

*Convergent-Beam  
Electron Diffraction  
II*

by

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# *Preface*

Nearly three years have passed since the previous book, "Convergent-Beam Electron Diffraction", JEOL-Maruzen, was published in 1985. The book surveyed the CBED method using a plenty of photographs. I believe it has served as a practical guide to the CBED method and also as a source of enjoyment to many.

However, many worthwhile materials are yet to be published, which would permit a more extensive use of the CBED method. Included among these materials are those on an experimental technique to take simultaneously a zone-axis pattern and  $\pm G$  dark-field patterns, spurious symmetries, dynamical extinction rules for higher-order Laue-zone (HOLZ) reflections, computer simulations of CBED patterns and the identifications of the displacement vector of a stacking fault and the Burgers vector of a dislocation. The symmetry determinations of a high  $T_c$  superconductor ( $\text{La}_2\text{CuO}_{4-\delta}$ ), magnetite, quasicrystals and incommensurate phases provide a better understanding of the practical uses of the CBED method, thereby showing its great potential. I have included many unpublished works in this issue because the results of these pioneering works should make this book fresh and unique. Crystal structure analysis or the determination of atomic positions using the CBED method will be carried in the next volume. The style of the previous book is followed also in this volume, that is, a good reproduction of photographs and short explanations of each subject.

In the previous book, we added simple personal computer programs for drawing HOLZ lines just for readers reference. However, I was surprised to have had many inquiries about these. Hence, in this volume, we present not only a program for drawing HOLZ lines with better performance, but also those for drawing Kikuchi lines and CBED patterns from dislocations and for determining specimen thickness. We also present flow charts of the methods for determining point and space groups and for identifying defects and flow charts of the experimental procedures for various CBED techniques. We hope that these things will be helpful in lowering some barriers which electron microscopists may encounter when they begin to use the CBED method.

The data shown herein was obtained with the cooperation of successive graduate students of Department of Physics, Tohoku University. These include Mr. R. Saito (presently at Hitachi Research Lab., Hitachi Ltd.), Dr. S. Matsuda (Textile Research Lab., Asahi Chemical Industry Co., Ltd.), Dr. S. Suzuki (R&D Division Asahi Glass Co., Ltd.), Mr. H. Sekii (Central R&D Lab., Omuron Tateishi Electrics Co.), Mr. T. Nagasawa, Mr. O. Ueno (Electronic Imaging and Research Lab., Fuji Xerox Co., Ltd.), Mr. H. Takayoshi (Komukai Works, Toshiba Co.), Mr. S. Ito, Mr. Y. Miyamura, Mr. A. Ishikawa and Mr. K. Tsuda (Master Course, Department of Physics, Tohoku Univ.), and Mr. M. Terauchi (Doctor Course, Department of Physics, Tohoku Univ.) and Mr. T. Kaneyama (EM Group, JEOL Ltd.), who are the co-authors of this book. I am deeply indebted to these people for their kind cooperation in the preparation of this work. The photographs included in this publication were taken with a JEM-100CX equipped with a field emission gun (FEG) and a JEM-2000FX.

I express my cordial gratitude to JEOL Ltd.' staff, especially Mr. T. Eto, Mr. Y. Harada, Mr. Y. Ishida, Mr. Y. Kokubo, Mr. M. Naruse and Mr. T. Tomita for their devoted collaboration in instrument development. I also wish to thank Mr. F. Sato for his outstanding maintenance of the JEM-100CX-FEG and the JEM-2000FX, and for his highly skilled photography. I also express my heartfelt thanks to Professor D. Watanabe for allowing me and the graduate students to concentrate on this work. Without the devoted help of Mr. A. Shoji, Mr. H. Matsuo and Mr. T. Handa of JEOL Ltd. in the compilation of the book, and of Mr. T. Takamatsu in the critical reading of the manuscript, this edition could never have been possible. It is pleasure to pay tribute also to Mr. T. Kondo of Kyoritsu Printing Co., Ltd. for the excellent printing of this book.

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Sendai, Summer 1988

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# Introduction

The standard method of point-group determination, which was given by Buxton *et al.* [1], requires that four patterns (whole, bright-field, dark-field and  $\pm G$  dark-field patterns) be taken. With the ordinary experimental method, these patterns are recorded on three different films at different times and at different crystal settings. It is desirable to develop experimental techniques by which these four patterns are recorded simultaneously on a film. One of such techniques was already reported in the reference [2] and also described in the previous book [3] (hereafter referred to as book I). However, the technique needs large flat-surfaced specimen areas and brings the exact Bragg positions to off-center positions of the diffraction disks. An improved technique [4] which enables us to take the four patterns from a smaller specimen area and to set the exact Bragg positions to the disk centers is described first.

CBED can identify 32 crystal point groups unambiguously [1], [5]. However, we found that spurious symmetries arise from crystals of a certain structure type [6]. The structure is composed of two equivalent substructures which are displaced from each other by a certain vector and are each occupied by a different kind of atoms. The crystals with such a structure often exhibit a symmetry  $m_2$  or  $1_R$  in the dark-field pattern, or  $2_R$  between a pair of dark-field patterns despite the fact that they do not have a horizontal twofold axis, a horizontal mirror plane, and an inversion center. These spurious symmetries are harmful to the correct determination of point-groups. Hence, it is important to know the origin of the phenomena to avoid incorrect identification of point-groups. Examples of spurious symmetries are shown and a short theoretical analysis of the phenomena is given.

We add an observation of a symmetry  $m_2$  due to a twofold axis oblique to the specimen surface. This axis is not a symmetry element of an infinitely extending parallel sided specimen or diperiodic plane figures, which Buxton *et al.* [1] postulated in their study of point-group determination.

Concerning the dynamical extinction, there are many things to be described. The dynamical extinction rules, which were given by Gjønnes and Moodie [7], are the basis of space-group determination. The extinction appears as lines of zero intensity in kinematically forbidden reflection disks when a screw axis is set perpendicular to the incident beam or when a glide plane is set parallel to it. These dark lines, which are called GM lines after Gjønnes and Moodie, have successfully been utilized for the identification of screw axes and glide planes. Tables

of dynamical extinction in which expected GM lines appearing in the 0th order Laue-zone (ZOLZ) reflections are listed for various incident-beam directions of all the space groups were given by Tanaka *et al.* [3], [8].

The dynamical extinction due to a glide plane which is set perpendicular to the incident beam has also been predicted to appear as a dark spot at the exact Bragg position of a kinematically forbidden reflection. This extinction had not been observed, however, until our investigation was made [9]. We give here examples of the extinction. On the basis of the experimental results, the extinction rule given by Gjønnes and Moodie has been modified in a practical manner.

Spurious  $B_3$  GM lines occur as well as the spurious symmetries described in the section of point-group determination. What we call spurious  $B_3$  GM lines are dynamical extinction lines appearing in kinematically forbidden reflections at the symmetric electron incidence and at the incidences exactly exciting kinematically allowed reflections. At these incidences there exist pairs of Umweganregung paths via higher-order Laue-zone (HOLZ) reflections to a kinematically forbidden reflection. The phases of the two beams coming through a pair of paths are different by  $\pi$  from each other. The two beams are different in amplitude, unlike cases of exactly exciting kinematically forbidden reflections. As a result, partial cancellation takes place between the two beams. If the difference between the amplitudes is small, the extinction line is still observed. The presence of the spurious  $B_3$  GM lines, together with true GM lines, indicates the existence of a screw axis, unlike the spurious symmetries described in the section of point-group determination.

What will happen to GM lines when a screw axis or a glide plane is slightly destroyed by small displacements of constituent atoms, which may occur, for instance, due to a second-order phase transition? The answer is that crossed  $A_2$  and  $B_2$  GM lines [8] with a symmetry  $2mm$  due to the interaction of ZOLZ reflections change into a pattern with a symmetry  $1_R$ , which is expected from the horizontal mirror plane existing in the case of ZOLZ interaction. This change is worth remembering for the symmetry identification of patterns with a subtle symmetry. We give a good example of a CBED pattern for a slight breakdown of the  $2_1$  screw axis in  $\text{Mo}_2\text{S}_3$ , which takes place at the phase transition from the space group  $P2_1/m$  to  $P\bar{1}$  or  $P1$ . Such a change is confirmed in the section of computer simulations.

The observation of  $A_3$  and  $B_3$  GM lines [8] due to HOLZ interaction is sometimes difficult at room tem-

perature because of large-amplitude lattice vibration. Cooling specimens, if possible, allows unambiguous observation of these lines. It is worth while observing how the visibility of the lines is improved by cooling specimens. Distinct  $A_3$  GM lines taken from Si at the liq.N<sub>2</sub> temperature have to be compared with faint ones at room temperature given in book I. A  $B_3$  GM line from FeS<sub>2</sub> was clearly observed at the liq.N<sub>2</sub> temperature while it was not seen at room temperature.

The space-group determination method [8] uses the dynamical extinction lines (GM lines) appearing in ZOLZ reflections. The GM lines are caused by the crystal symmetry elements which act as horizontal 2<sub>1</sub> screw axes, vertical glide planes with horizontal translation vectors and horizontal glide planes [7].

The vertical glide planes with arbitrary translation vectors give rise to GM lines also in HOLZ reflections. It is noted that vertical glide planes whose translation vectors are perpendicular to the specimen surface (vertical translation) do not cause GM lines in ZOLZ reflections but cause them in HOLZ reflections (see page 59) [10]. Tables of GM lines appearing in HOLZ reflections at various incident beam orientations for all the space groups which have glide planes, are given in an appendix. Use of the GM lines appearing not only in ZOLZ but also in HOLZ reflections ensures unambiguous and quick identification of space groups.

The vertical glide plane whose translation vector has a vertical component is not a symmetry element of diperiodic plane figures. The assumption of the diperiodic plane figures made by Buxton *et al.* [1] is not suitable when the symmetry elements of space groups are concerned. The GM lines due to vertical screw axes are difficult to observe in usual transmission CBED, because they can be seen in backscattered reflection disks. It makes no sense to construct space groups using actually observable symmetry elements, because they do not form a complete set. CBED does not observe all the symmetry elements of crystal space groups, but observe much more than the symmetry elements of diperiodic plane figures.

Space-group determination using ZOLZ and HOLZ GM lines is demonstrated for a high  $T_c$  superconductor, La<sub>2</sub>CuO<sub>4-δ</sub>, and the low temperature phase of magnetite (Fe<sub>3</sub>O<sub>4</sub>) in which charge ordering (Verwey order) had been believed to occur.

The repetition of a unit cell, the translational symmetry, is a characteristic feature of crystals. An exception—incommensurate structure—appears, however, in a crystal over a certain temperature range. The

period of this structure does not coincide rationally with that of the protophase. The incommensurate phase occurs when two competitive interactions are present between the first and second nearest neighbouring atoms. The phase, characterized by a temperature dependent wave number vector, causes the discommensuration at its lower temperature region and transforms into a commensurate phase due to a lock-in transition. The incommensurate structure is described by a three-dimensional section of a crystal in a higher-dimensional space [11]. Whether the symmetry elements allowed in a higher-dimensional space provide new symmetries in CBED patterns has not yet been clarified. CBED, however, can reveal what symmetry element of the protophase is destroyed and what type of a wave, a transverse or a longitudinal one, is produced in the related incommensurate phase. Such information is useful for the structure analysis of the phase, like the space-group determination performed before the determination of atomic positions. The first study of an incommensurate structure was performed by Steeds *et al.* on NiGe<sub>1-x</sub>P<sub>x</sub> [12]. We give two examples of studies carried out on Sr<sub>2</sub>Nb<sub>2</sub>O<sub>7</sub> and Mo<sub>8</sub>O<sub>23</sub>.

The discovery of an alloy of aluminum and manganese [13] which shows sharp diffraction spots with an icosahedral symmetry has had a great impact on crystallography and solid state physics. It has revealed the existence of a new structural order (quasicrystal). The quasicrystal is defined to have a quasi-periodic long-range structural order with a noncrystallographic point group and to have a self-similarity transformation. The discovery of quasicrystals has accelerated the theoretical development of the crystallography in high-dimensional spaces. CBED is definitely the best method to investigate the symmetry of this new class of structural order [14,15,16]. We shall briefly report the latest results of CBED and small-area-parallel-beam electron diffraction studies on real quasicrystals.

CBED is now entering a stage of quantitative studies. Computer simulation of CBED patterns [17] is indispensable for their quantitative analysis. We simulated several CBED patterns using the ordinary matrix-diagonalization method for the dynamical theory of electron diffraction, and utilized the simulation for the sensitivity test of CBED patterns on a slight breakdown of a glide plane and/or a screw axis. The test proved the high sensitivity of the patterns to the breakdown of the crystal symmetries and gave instructive results on how the CBED symmetries change as the degree of the breakdown increases. Using computer simulation, we are now developing a crystal

structure analysis method based upon the dynamical theory. Structure analysis using the dynamical theory has been carried out by Vincent *et al.* for AuGeAs [18].

CBED has a great potential to identify not only crystal space groups but also crystal lattice defects. In book I, we already quoted the work of Johnson on a stacking fault [19] and that of Carpenter and Spence [20] on a dislocation. Recently, detailed studies to determine the displacement vector  $\mathbf{R}$  of a stacking fault have been carried out [21,22] by utilizing information not only from  $\alpha = 2\pi\mathbf{g}\cdot\mathbf{R} = 0$  but also from finite values of  $\alpha$ . The method using HOLZ lines allows us to know the magnitude and sign of the vector. That is, it can determine easily and unambiguously whether the fault is intrinsic or extrinsic, while the traditional electron microscope-image method is rather complicated and open to misidentification. The CBED method is of course based on dynamical diffraction but does not utilize the absorption effect unlike the method using microscope images. This indicates that the present method can apply to specimens thinner than an extinction distance.

Cherns and Preston [23] have found that the whole strain field of a dislocation must be illuminated by a convergent beam to determine the Burgers vector  $\mathbf{b}$  of a dislocation. They have proposed a method of determining Burgers vectors. The method uses defocus illumination and consequently provides two items of information on the strain fields of dislocation—the real and reciprocal spaces. In such a CBED pattern, a reflection line across a dislocation shows  $n$  nodes at their crossing region when  $\mathbf{g}\cdot\mathbf{b} = n$ . The values of  $n$ 's obtained for three linearly-independent reflections allow the unique determination of the Burgers vector, where the importance of the relative signs of  $n$ 's should be emphasized [22]. We give a few examples of Burgers vector determination using the excellent method of Cherns and Preston. We have applied the method further to the Burgers vector determination of a partial dislocation, which is closely related to a stacking fault [21], and of a dislocation loop, which is related to the precipitation of interstitial atoms and vacancies. The method has also been applied to the investigation of particular effects due to edge and mixed dislocations,  $\mathbf{g}\cdot\mathbf{b}_e$  and  $\mathbf{g}\cdot\mathbf{b} \times \mathbf{u}$ , and those due to an extended dislocation.

The need for CBED characterization of interfaces between crystal lattices is rapidly increasing, especially in the light of industrial importance of artificial super-lattice crystals. We are not concerned, however, with the matter at present. Thus, we only quote two papers dealing

with the subjects presented by Maher *et al.* [24] and Eaglesham and Humphreys [25].

In the section of applications are described the development of the degree of order observed just after a second-order phase transition of  $\text{Sr}_2\text{Ta}_2\text{O}_7$ , and the crystallographic relation between adjoining domains revealed for  $\text{TaS}_3$  and  $\text{Sr}_2\text{Ta}_2\text{O}_7$ . We hope that readers appreciate the beautiful large-angle CBED (LACBED) patterns and hollow-cone beam CBED (HCB-CBED) patterns which were chosen in accordance with the authors' taste.

We add several appendices. Firstly, flow charts of various experimental techniques, point-group and space-group determinations, and identification methods for stacking faults and dislocations are given. Secondly, tables of GM lines appearing in HOLZ reflections are given, which can be successfully used for the identification of glide planes as well as the GM line tables for ZOLZ reflections given in book I. Computer programs were prepared for the personal computer of NEC-PC9801. For printing out results, we use the printer of NEC-PC-PR201, the plotter of Roland DXY-990, and the laser printer of Canon LBP-B406. The HOLZ line program listed in this volume has much better performance than the one provided in book I. The Kikuchi line program allows drawing Kikuchi-line maps, indexing observed zone axes and measuring the angle between two zone axes. The program for thickness determination is based on the method described in book I. These three programs, saved in a diskette, are supplied from JEOL Ltd. The simulation program for the profile of a reflection crossing a dislocation is omitted, but hard copies of input data on a CRT and an obtained result are given for readers' information. The CBED users need only the results shown in the section of lattice defects; it is not necessary to recalculate the profiles. This program, however, will also be supplied from JEOL Ltd. in the near future. Readers who wish to know the details of this program are requested to contact the authors. A simplified flow chart of dynamical calculation and obtained results are added.

The reciprocal-space lines corresponding to CBED disks are illustrated, and elimination techniques for specimen contamination are described as readers' reference.

Lastly, a reference of Steeds [26] is given for a general survey of the CBED method and other references, those of Lehmpfuhl and Dowell [27] and Eades *et al.* [28] are added as important topics of reflection CBED.

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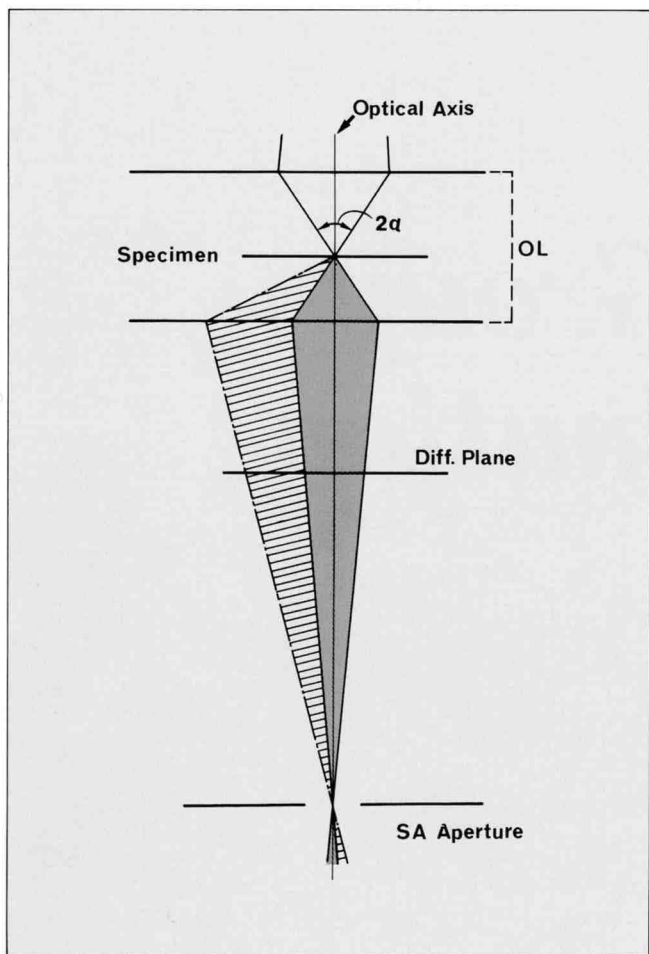
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## *Abbreviations of Technical Terms*

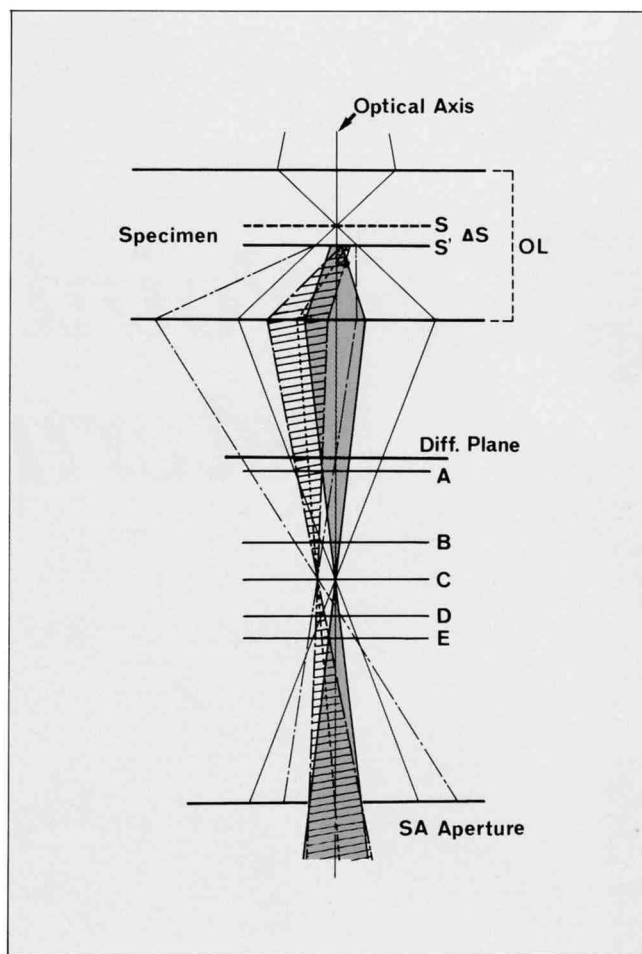
CBED	Convergent-Beam Electron Diffraction
ZAP	Zone-Axis Pattern
WP	Whole Pattern
BP	Bright-Field Pattern
DP	Dark-Field Pattern
± DP	± Dark-Field Pattern
ZOLZ	Zeroth Order Laue-Zone
H(F,S)OLZ	Higher (First, Second) Order Laue-Zone
GM Line	Gjønnnes-Moodie Line = Dynamical Extinction Line
LACBED Pattern	Large-Angle CBED Pattern
HCBCBED Pattern	Hollow-Cone Beam CBED Pattern
MB-LACBED Pattern	Many-Beam LACBED Pattern
SA-CBED Pattern	Selected-Area CBED Pattern
FEG	Field Emission Gun
CTEM	Conventional Transmission Electron Microscopy
SAMAG mode	Selected Area Magnification mode
SADIFF mode	Selected Area Diffraction mode
BFI	Bright-Field Image
DFI	Dark-Field Image
CL	Condenser Lens
OL	Objective Lens
IL	Intermediate Lens
DEF1,2	Deflector 1,2
α-selector	Convergence Angle Control of the Incident Beam
HCBC generator	Hollow-Cone Beam generator
FLC mode	Free Lens Control mode
Z-control	Specimen Height control

# *Point-Group Determination*

# Simultaneous Observation of ZAP and $\pm G$ Dark-Field Patterns



Ordinary CBED method. The convergence angle  $2\alpha$  is set to twice the Bragg angle of the lowest order reflection.



Selected area CBED (SA-CBED) method. The excitation of the objective lens is increased from the condenser-objective condition (the left diagram). The specimen receives defocused illumination. The selector aperture is used to select the convergent beam angle (and specimen area). The intermediate lens is focused on a plane between A and B.

When the standard CBED method of Buxton *et al.* [1] is used to determine point groups, the four patterns (whole, bright-field, dark-field, and  $\pm G$  dark-field patterns) appearing in three photographs are needed. With the ordinary experimental method, these patterns are not obtained simultaneously, but are recorded on different films at different times and at different crystal settings. It is desirable to develop experimental techniques by which these four patterns are recorded simultaneously on a film. We already developed such a method [a] and described it in book I. However, the method requires an about 1- $\mu\text{m}$ -diameter specimen area with a uniform thickness and with no bend. Exact Bragg positions are at off-centers of dark-field disks, which makes some portions of the patterns ineffective for symmetry determination.

A new method [b] can take simultaneously the four patterns from a specimen area about 100 nm in diameter with exact Bragg positions kept at the centers of dark-field disks, although the angular size of each disk is smaller than that in the previous method.

The ray path of the ordinary CBED method is shown in the left diagram. The convergence angle  $2\alpha$  of the incident beam is set to twice the Bragg angle of the lowest order reflection so that the CBED disks are in contact with each other. The incident beam is converged on the specimen. The image of the specimen is formed on the selector aperture, because the condenser-objective condition is satisfied for the objective lens. The intermediate lens is focused on the back focal plane of the objective lens.

The right diagram illustrates the final ray path of the new method. The incident-beam angle is set larger than that in the ordinary CBED method by removing the condenser aperture from the optical axis. The selector aperture is inserted in the optical axis. The excitation of the objective lens is increased so that the cross-over point of the incident beam is imaged above the selector aperture. As a result, the back focal plane moves from plane A to a plane written as Diff. plane, but the two planes are so near that they are not necessary to distinguish. The intermediate lens remains focused on plane A. The specimen position is shifted to a position S' with a specimen height control so that the exactly Bragg reflected beam crosses the optical axis at the selector aperture. Finally, the selector aperture size and the excitation of the objective lens are readjusted so that neighbouring disks do not overlap each other.

The maximum nonoverlapping disk size on plane A is limited to the Bragg angle of the lowest order reflection or one-half the angle obtained by the ordinary method. It is seen in the right diagram that the reflection disks are separated from each other below plane A. This indicates that disks with larger angular spreads can be obtained. CBED patterns obtained at plane B have a disk

size almost twice that at plane A or the same as that in the ordinary method.

We remember that in ordinary selected area diffraction, the selector aperture selects a specimen area, because it is inserted in the image plane. Since in the present method, a defocused image is formed on the selector aperture, the aperture selects both the illuminated specimen-area size and the angular size of the incident beam. Therefore, the method is regarded as an extension of selected area diffraction. We call it selected-area CBED (SA-CBED). The specimen area selected by the disks of the transmitted beam and six 220 reflected beams was calculated to be about 100 nm in diameter for a pattern of (111) Si formed on plane B using a 5- $\mu\text{m}$ -diameter selector aperture.

High resolution of the pattern formed on plane B is ensured when the incident beam impinges on a point of the specimen with an incidence angle without any divergence. Such illumination is realized only when the source size of the electron gun is sufficiently small. When only the central beam emitted from an  $\text{LaB}_6$  cathode heated at an unsaturated condition is used, a fairly good angular and/or spatial resolution is obtained. Our JEM-100CX, equipped with a field emission gun having a virtual source diameter of about 40 nm, has been successfully used for the present purpose. In fact, the HOLZ lines in the pattern taken at plane B are seen as sharp as in the pattern taken at plane A without detectable deterioration.

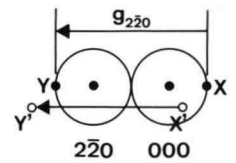
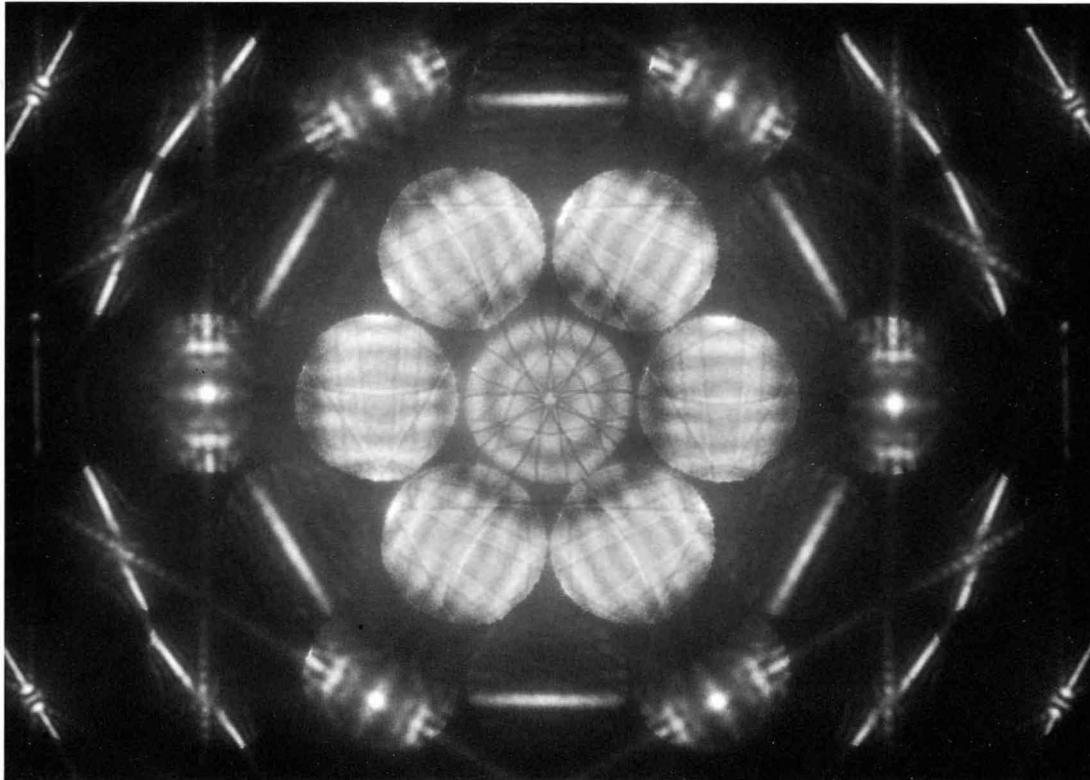
The first advantage of this method is that the size of the selected area is much smaller than that needed in the previous method [a]. The second is that exact Bragg positions can be brought to the centers of diffraction disks. The third advantage is that the pattern can be observed with less contamination even for insufficiently clean specimens, because this method, as well as the LACBED method, does not use the condenser aperture but exposes the specimen to a beam shower.

## References

- [a] M. Terauchi and M. Tanaka: *J. Electron Microsc.*, **34** (1985) 128.
- [b] M. Terauchi and M. Tanaka: *J. Electron Microsc.*, **34** (1985) 347.

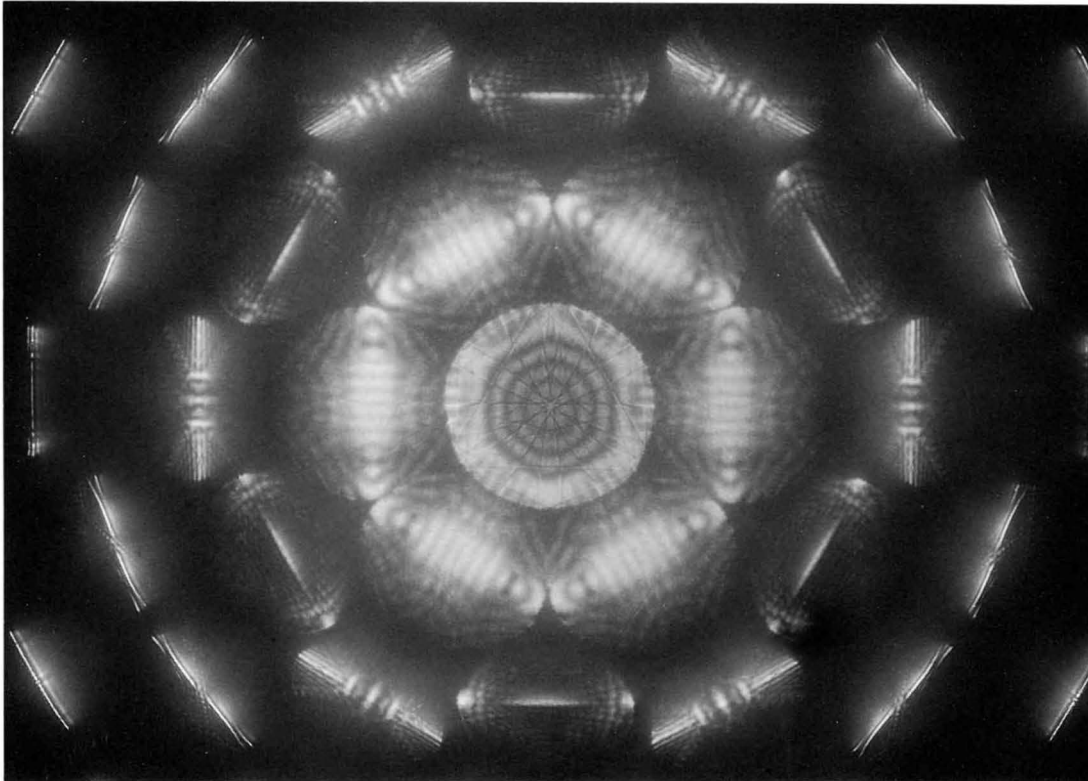
Si [111]

60 kV



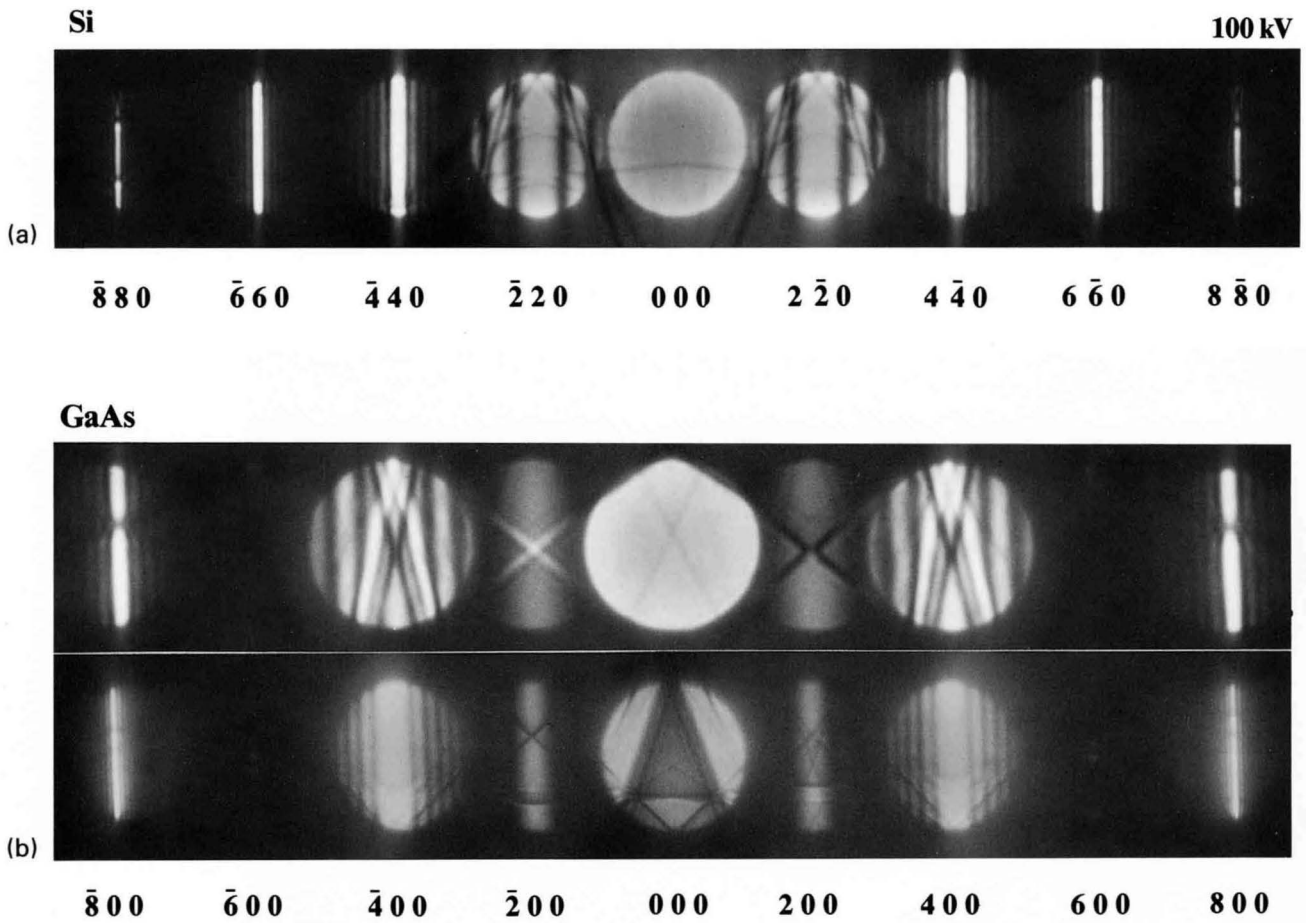
SA-CBED pattern of (111) Si. The intermediate lens was focused on plane A, which lay nearly at the same level as the back focal-plane. The angular size of the disks is the Bragg angle of the  $2\bar{2}0$  reflection,  $1 \times 10^{-2}$  rad. The exact Bragg position is at the center of each disk.

The two schematical disks at right express the  $000$  and  $2\bar{2}0$  CBED disks produced on the back focal-plane. The  $2\bar{2}0$  beams diffracted from the  $000$  beams do not fall in the  $2\bar{2}0$  disk but outside it. The selected specimen areas corresponding to these disks are different from each other.



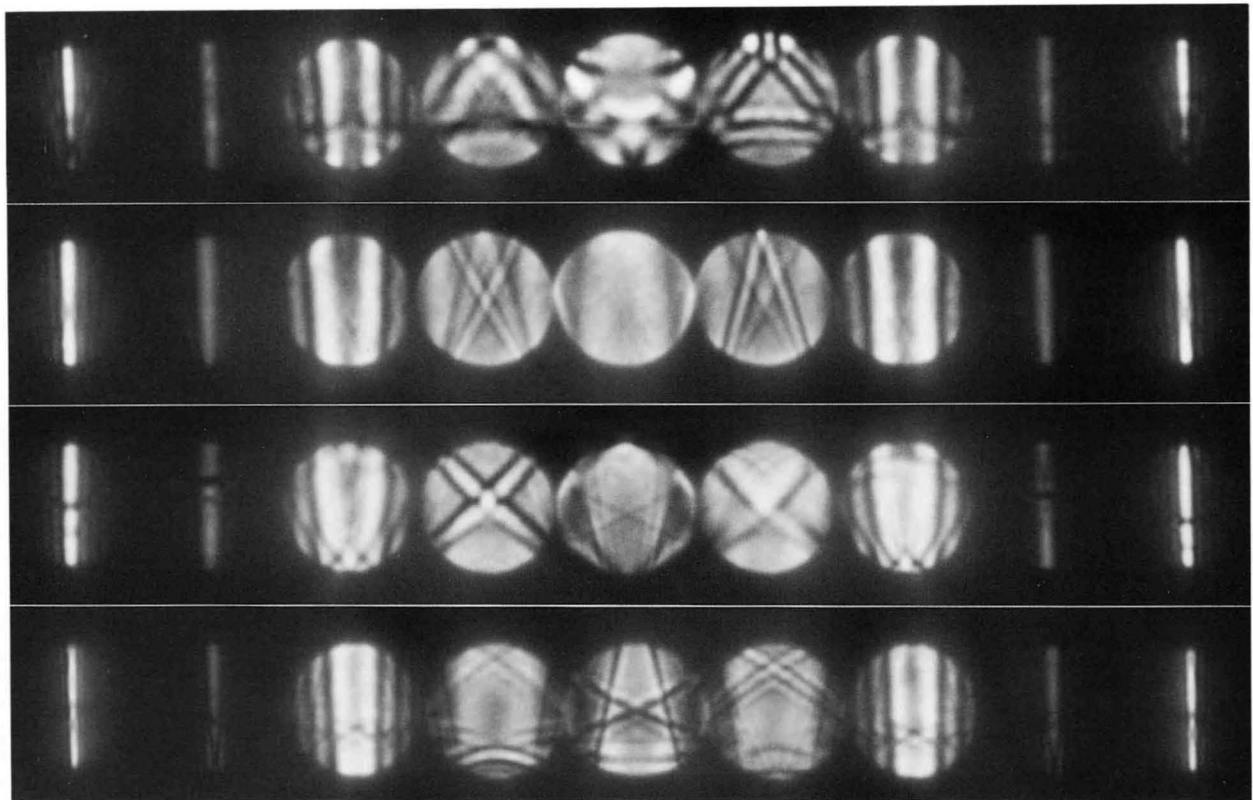
SA-CBED pattern of (111) Si. The intermediate lens was focused on plane B. The angular size of the disks is twice the Bragg angle of the  $2\bar{2}0$  reflection,  $2 \times 10^{-2}$  rad. The exact Bragg position is at the center of each disk.

The two schematical disks at right express the 000 and  $2\bar{2}0$  disks produced on plane B. The beams in the shaded area in the 000 disk are diffracted into the shaded area of the  $2\bar{2}0$  disk. The illuminated specimen area corresponding to the shaded areas is the same.



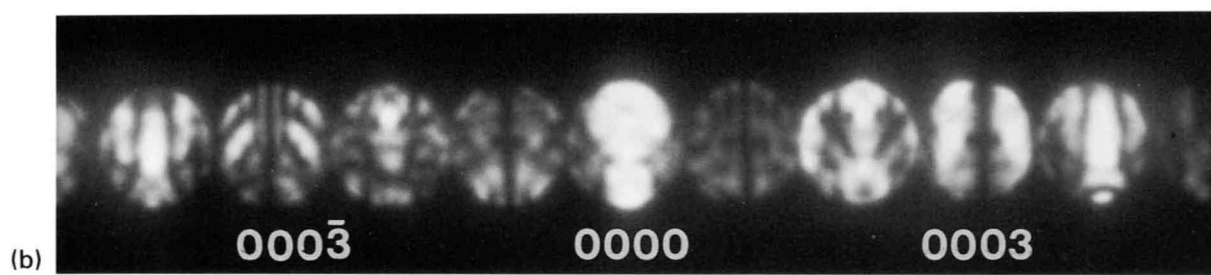
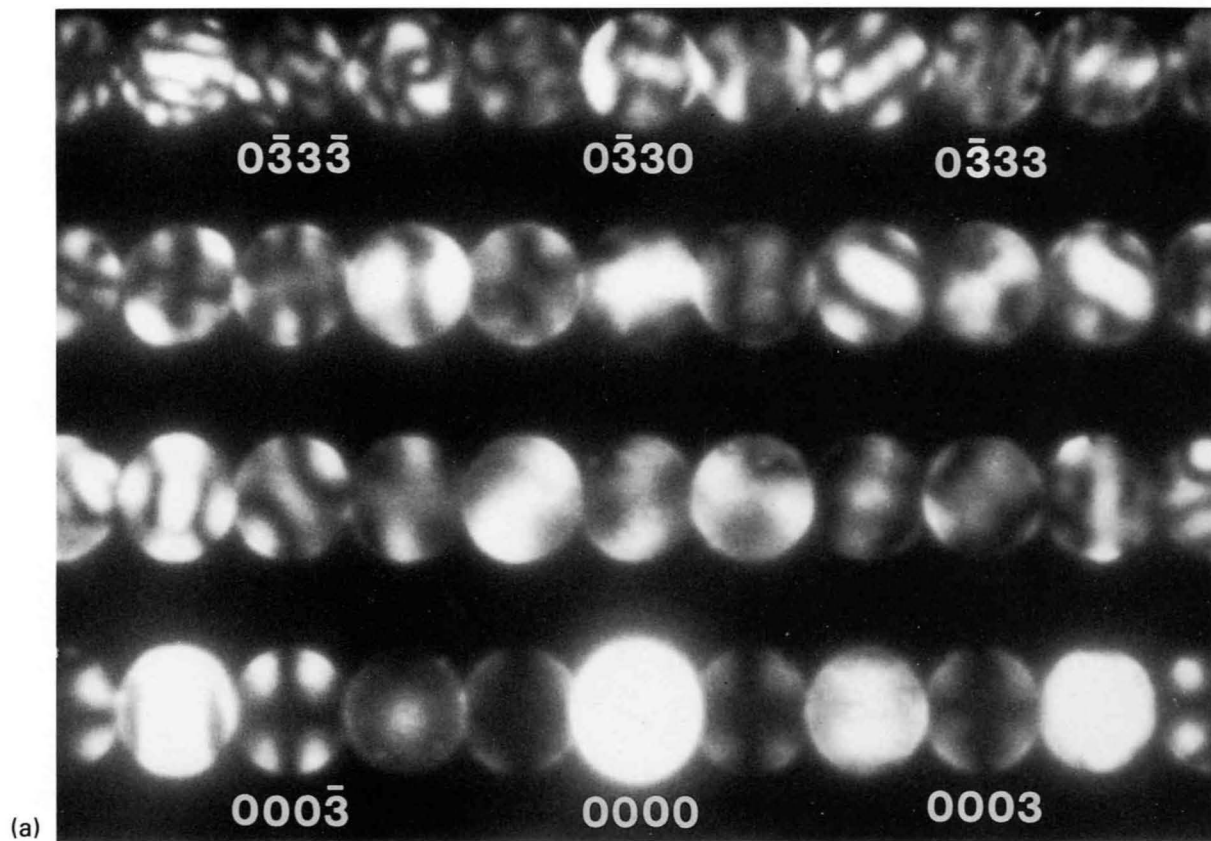
The photographs show SA-CBED patterns taken from Si(a), GaAs(b) and InP(c) by preferentially exciting the systematic reflections. The noncentrosymmetric property of GaAs and InP appears clearly as a lack of the translational symmetry in the  $200$  and  $\bar{2}00$  reflections, whereas the  $2\bar{2}0$  and  $\bar{2}20$  reflections from Si which have an inversion center show the same intensity distribution. In contrast to the ordinary method, the present method can, by varying the azimuthal angle, easily find favorable crystal orientations at which the intensity difference between  $200$  and  $\bar{2}00$  reflections from GaAs and InP is clearly observed, because the  $200$  and  $\bar{2}00$  dark-field patterns are observed simultaneously. Consequently, a distinct lack of symmetry  $2_R$  can be displayed for GaAs despite its slight noncentrosymmetry.

**InP**



(c)

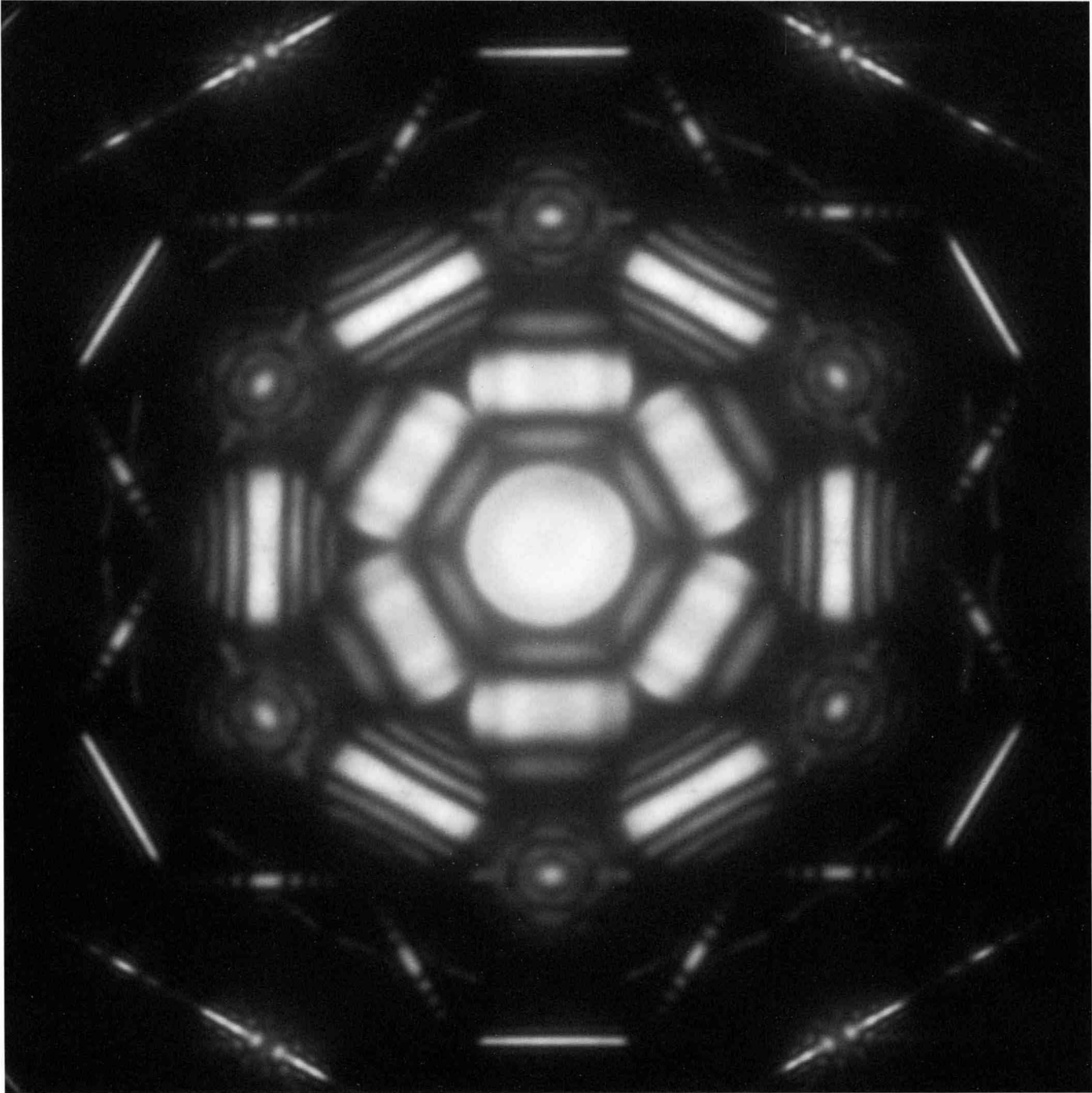
$\bar{8}00$     $\bar{6}00$     $\bar{4}00$     $\bar{2}00$     $000$     $200$     $400$     $600$     $800$



Photographs (a) and (b) show SA-CBED patterns taken from CdS belonging to the space group  $P6_3mc$  at the  $\bar{2}110$  zone axis setting and at a crystal setting tilted by more than a few degrees from the zone axis about the  $[0001]$  axis, respectively. Crossed dynamical extinction lines [7] ( $A$  and  $B$  GM lines[8]) are clearly seen at the centers of all the odd order  $000l$  forbidden reflections in Photo (a), whereas the crossed lines are observed only in one disk by the ordinary method.

No symmetry between  $\pm 000l$  disk pairs proves that the crystal is noncentrosymmetric. All the reflections of the index  $k \neq 0$  show symmetries  $1_R$  due to two-dimensional interaction. The patterns of these reflections are compared with LACBED patterns which were taken by laborious work and shown in book I.

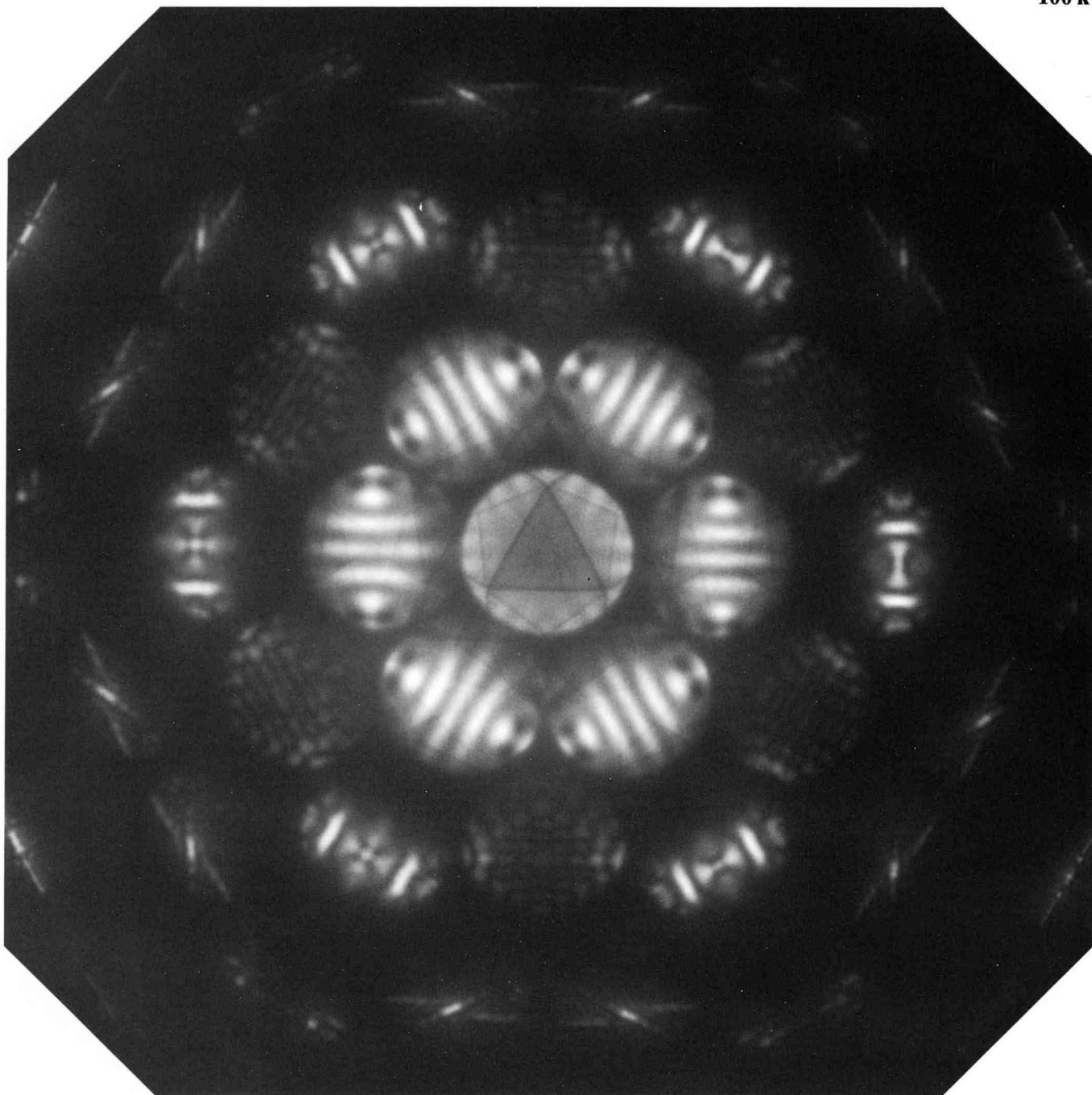
In photograph(b), only  $B$  GM lines are displayed in all the odd order  $000l$  disks, because the specimen was tilted from the zone axis. This is clear evidence of the fact that the lines were produced from the  $6_3$  screw axis. The lack of symmetries  $2_R$  is seen more clearly than that in Photo (a).



SA-CBED pattern

Ge [111]

100 kV



SA-CBED pattern

# Spurious Symmetries

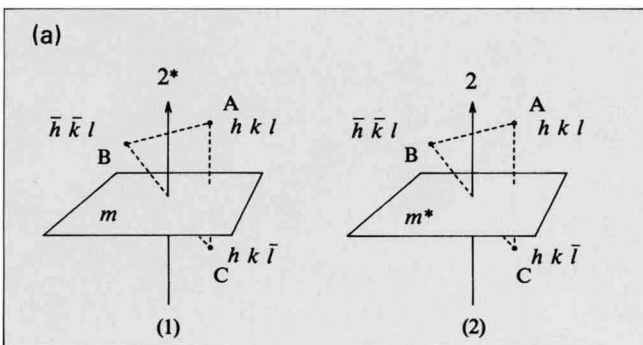
Convergent-beam electron diffraction (CBED) patterns do not always show true symmetries of a specimen crystal, but may show higher symmetries than those expected from the specimen (symmetry enhancement). If the phase of a structure factor can not be detected, symmetry enhancement or spurious symmetries can take place, like a classical example that the lack of an inversion center can not be detected by X-ray diffraction.

When the structure factors of two reflections which are related to each other by a twofold rotation have the same amplitude but different phases, let us regard that a pseudo twofold rotation axis  $2^*$  is present between two reflections (A and B in Fig. (a)-1). A pseudo mirror plane  $m^*$  is defined in a similar manner (A and C in Fig. (a)-2).

A pseudo twofold axis and a pseudo mirror plane always exist perpendicular to a true mirror plane and a true twofold axis, respectively. In these cases, two structure factors related by these pseudosymmetry elements are complex conjugate to each other. It was theoretically proved that the pseudo symmetries do not cause spurious symmetries. However, spurious symmetries  $m_2$ ,  $1_R$  and  $2_R$  [a] have been experimentally observed in several crystals which have no horizontal twofold axis, no horizontal mirror plane and no inversion center. We investigated the origin of the observed spurious symmetries.

The crystals which caused the spurious symmetries were found to be composed of two equivalent substructures, which are displaced from each other by a certain vector and are each occupied by a different kind of atoms. We call this type of structures the AA' structure. It may safely be said that the AA' structure does not exhibit the symmetry of the whole structure but that of the substructure in the dark-field pattern. We see on pages 21 to 32 examples of spurious symmetries obtained from crystals of the zinc-blende (ZnS) type structure and polytypes of SiC, these structures actually belonging to the AA' structure (Fig. (b)).

The kinematical structure factor  $F(\mathbf{h})$  of the AA' structure is expressed as



$$F(\mathbf{h}) = (f_A + f_B \exp 2\pi i \mathbf{h} \cdot \mathbf{R}) \sum_j \exp 2\pi i \mathbf{h} \cdot \mathbf{r}_j = H(\mathbf{h})G(\mathbf{h}), \quad (1)$$

where  $\mathbf{R}$  is the displacement vector between two substructures,  $H(\mathbf{h}) = f_A + f_B \exp 2\pi i \mathbf{h} \cdot \mathbf{R}$  and  $G(\mathbf{h}) = \sum_j \exp 2\pi i \mathbf{h} \cdot \mathbf{r}_j$ .

The crystal structure factor  $F_{\mathbf{h}}$  which takes account of multiple reflections is written as

$$F_{\mathbf{h}} = -iF(\mathbf{h})Z(\varrho_{\mathbf{h}}) - F(\mathbf{h}_1)F(\mathbf{h} - \mathbf{h}_1)Z'(\varrho_{\mathbf{h}_1}, \varrho_{\mathbf{h} - \mathbf{h}_1}) + \dots \quad (2)$$

where  $Z$  and  $Z'$  are functions of the excitation errors  $\varrho$  of reflections concerned.

Substitution of eq. (1) into eq. (2) yields

$$F_{\mathbf{h}} = -iH(\mathbf{h})G(\mathbf{h})Z - H(\mathbf{h}_1)H(\mathbf{h} - \mathbf{h}_1)G(\mathbf{h}_1)G(\mathbf{h} - \mathbf{h}_1)Z' + \dots = -i\hat{H}_1\hat{G}_1Z - \hat{H}_2\hat{G}_2Z' + \dots \quad (3)$$

where  $\hat{H}_1 = H(\mathbf{h})$ ,  $\hat{G}_1 = G(\mathbf{h})$ ,

$$\hat{H}_2 = H(\mathbf{h}_1)H(\mathbf{h} - \mathbf{h}_1), \quad \hat{G}_2 = G(\mathbf{h}_1)G(\mathbf{h} - \mathbf{h}_1), \dots$$

Let us consider a spurious symmetry  $m_2$  in the  $2\bar{2}0$  dark-field pattern obtained at the [111] electron incidence from ZnS, which belongs to the space group of  $F\bar{4}m$  and has no twofold rotation axis in the [1 $\bar{1}$ 0] direction. The substructure of ZnS is of face-centered cubic and has a twofold axis in the [1 $\bar{1}$ 0]. The displacement vector  $\mathbf{R}$  is  $1/4$  [111].  $G$  and  $H$  are expressed as

$$\begin{aligned} G &= 4 && \text{for all of } h, k \text{ and } l : \text{ even or odd} \\ H &= f_A + f_B && \text{for } h + k + l = 4n \\ &= f_A + if_B && = 4n + 1 \\ &= f_A - f_B && = 4n + 2 \\ &= f_A - if_B && = 4n + 3 \end{aligned} \quad (4)$$

where A and B correspond to Zn and S.

Let us consider two positions in the  $2\bar{2}0$  dark-field disk, which form a symmetry  $m_2$ . The first terms of eq. (3) for these positions are the same. Figure (c) shows two double reflection paths (1) and (2) falling on these positions. Let us compare the second terms of eq. (3) for these two paths. As the substructure has a twofold axis in the [1 $\bar{1}$ 0] direction,  $\hat{G}_2^{(1)}$  is equal to  $\hat{G}_2^{(2)}$ . The reflection equivalent to the reflection  $hkl$  with respect to the twofold axis is  $\bar{k}\bar{h}\bar{l}$ . Thus,

$$\begin{aligned} H(\bar{k}\bar{h}\bar{l}) &= f_A(\bar{k}\bar{h}\bar{l}) + f_B(\bar{k}\bar{h}\bar{l}) \exp\left[\frac{\pi i}{2}(\bar{k} + \bar{h} + \bar{l})\right] \\ &= [f_A(hkl) + f_B(hkl) \exp\left[\frac{\pi i}{2}(h + k + l)\right]]^* \\ &= H^*(hkl). \end{aligned} \quad (5)$$

Similarly,

$$H(2+k, \bar{2}+h, l) = H^*(2-h, \bar{2}-k, \bar{l}). \quad (6)$$

$\hat{H}_2^{(1)}$  and  $\hat{H}_2^{(2)}$  are written as

$$\hat{H}_2^{(1)} = H(hkl) H(2-h, \bar{2}-k, \bar{l})$$

and

$$\hat{H}_2^{(2)} = H(2+k, \bar{2}+h, l) H(\bar{k}\bar{h}\bar{l}).$$

Thus,

$$\hat{H}_2^{(2)} = (\hat{H}_2^{(1)})^*. \quad (7)$$

When we consider the first and second terms of eq. (3),  $F_{2\bar{2}0}$  is expressed for the two paths as

$$\begin{aligned} F_{2\bar{2}0}^{(1)} &= -4i\hat{H}_1^{(1)}Z - 16\hat{H}_2^{(1)}Z' \\ F_{2\bar{2}0}^{(2)} &= -4i\hat{H}_1^{(2)}Z - 16\hat{H}_2^{(2)}Z' \\ &= -4i\hat{H}_1^{(1)}Z - 16(\hat{H}_2^{(1)})^*Z'. \end{aligned} \quad (8)$$

For obtaining  $F_{2\bar{2}0}^{(1)} = F_{2\bar{2}0}^{(2)}$ ,  $\hat{H}_2^{(1)}$  must be equal to  $\hat{H}_2^{(2)}$ . Then, from eq. (7),  $\hat{H}_2^{(1)}$  must be real. As  $H_2^{(1)}$  is not always real, the spurious symmetry does not occur in general.

### Calculation of $\hat{H}_2^{(1)}$

At the [111] incidence, reflections in the  $N$ th Laue zone satisfy the relation  $h+k+l=N$ . Thus,

$$\begin{aligned} H &= f_A + f_B \exp\left[\frac{\pi i}{2}(h+k+l)\right] \\ &= f_A + f_B \exp\left(\frac{\pi i}{2}N\right). \end{aligned} \quad (9)$$

When in the double reflection paths to the  $2\bar{2}0$  reflection,  $000 \rightarrow hkl \rightarrow 2\bar{2}0$ , the reflection  $hkl$  belongs to a  $2N$ th Laue zone, a spurious symmetry  $m_2$  is produced because  $H$  is

real. When the reflection  $hkl$  belongs to a  $(2N+1)$ th Laue zone,

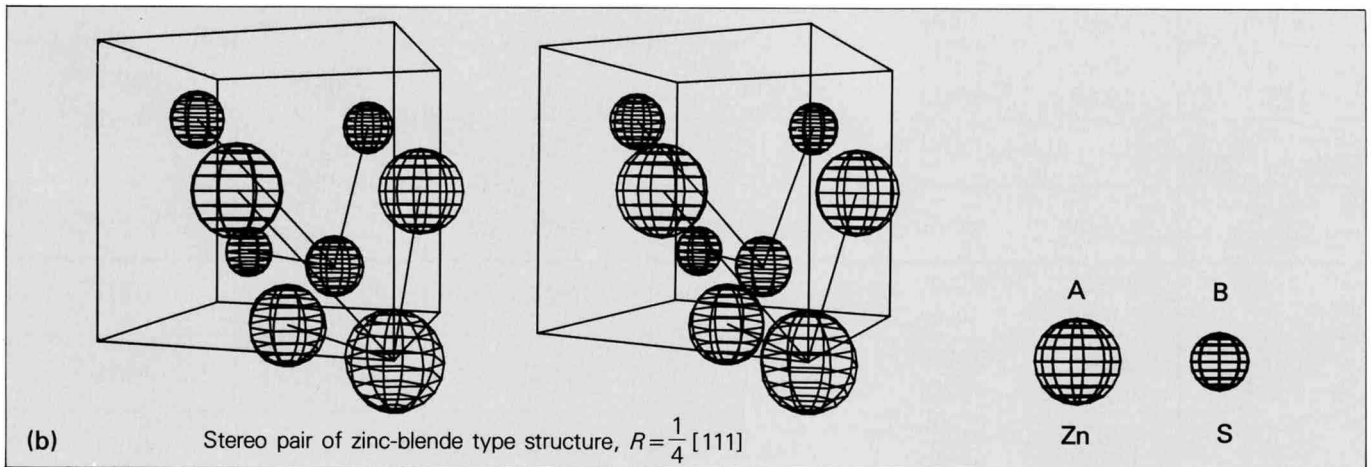
$$\begin{aligned} \hat{H}_2^{(1)} &= H(hkl) H(2-h, \bar{2}-k, \bar{l}) \\ &= (f_A \pm if_B)(f'_A \mp if'_B) \\ &= f_A f'_A + f_B f'_B \pm i(f'_A f_B - f_A f'_B) \end{aligned} \quad (10)$$

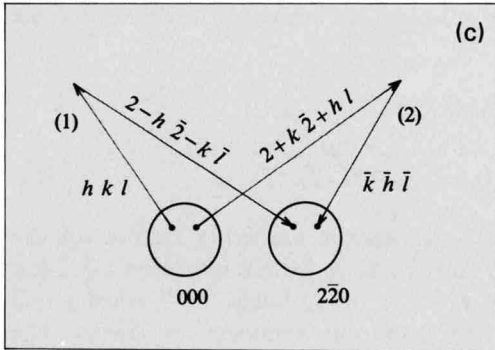
where  $f_A$  and  $f_B$  are atomic scattering factors for the reflection  $hkl$ , and  $f'_A$  and  $f'_B$  for the reflection  $2-h \bar{2}-k \bar{l}$ . If the relation  $f'_A/f_A = f'_B/f_B$  holds,  $H_2^{(1)}$  takes a real number, and then a spurious symmetry  $m_2$  occurs. The phase of  $H_2^{(1)}$  was calculated to be about  $1 \times 10^{-2}$  rad and  $3 \times 10^{-3}$  rad for several reflections of ZnS and GaAs, respectively (Tables (a) and (b)). We can safely ignore the higher order terms in eq. (3), although these terms can exhibit the true symmetry. Therefore, as a whole, an approximate spurious symmetry is produced. Figure (d) shows the atomic scattering curves of Zn and S. The spurious symmetry obtained originates from the fact that the scattering-angle dependences of the curves of Zn and S are approximately the same. This argument is a qualitative one, but not satisfactory for a quantitative account. Figure (e) shows rocking curves of the  $2\bar{2}0$  reflection of ZnS obtained by dynamical calculations using 10 ZOLZ and 8 HOLZ beams. The curves are symmetric with respect to the middle point, indicating the presence of symmetries  $m_2$ . Therefore, the computer simulations have proved the occurrence of the spurious symmetry.

Spurious symmetries  $m_2$  obtained from ZnS and GaAs at the  $[3\bar{3}\bar{2}]$  incidence and from SiC-15R at the  $[1\bar{1}0\bar{1}]$  incidence are shown on pages 24 and 25. Similar spurious symmetries were observed in  $1\bar{1}\bar{2}0$  dark-field patterns from LiTaO<sub>3</sub> and polytypes of TaS<sub>2</sub>.

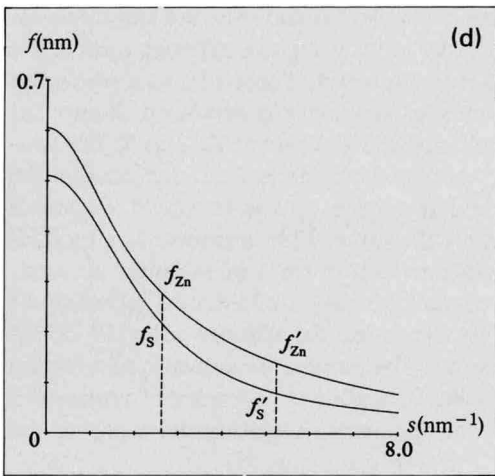
### Reference

- [a] M. Tanaka, H. Sekii, O. Ueno and H. Takayoshi: *Acta Cryst.*, **A40** Suppl. (1984) C384.

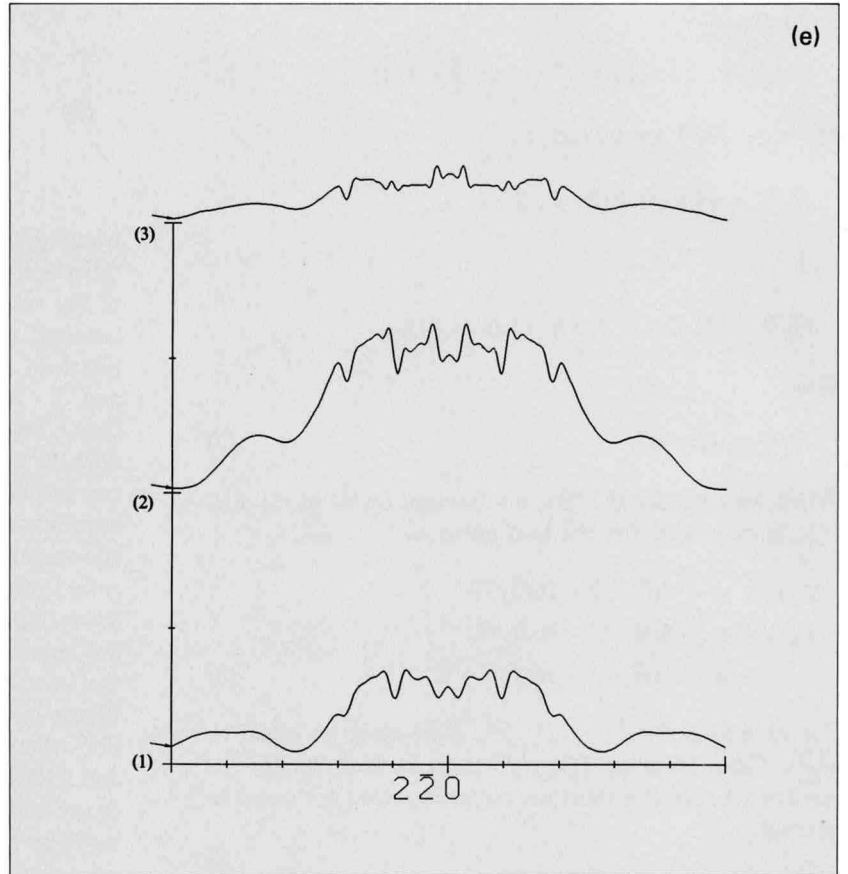




Double reflection paths forming a symmetry  $m_2$ .



Atomic scattering curves of Zn and S.



$2\bar{2}0$  rocking curves of ZnS calculated dynamically using 10 ZOLZ and 8 HOLZ reflections for three thicknesses (1) 99.9, (2) 124.8 and (3) 149.8 nm.

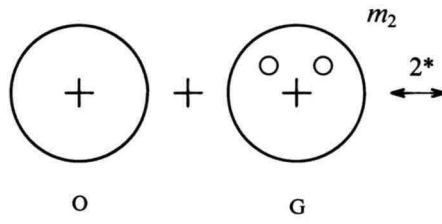
Table (a) GaAs

$\begin{matrix} hkl \\ 2-h, \bar{2}-k, \bar{l} \end{matrix}$	$f_{Ga}(nm)$	$f_{As}(nm)$	$R=f_{Ga}f'_{Ga}+f_{As}f'_{As}$	$I=f'_{Ga}f_{As}-f_{Ga}f'_{As}$	$\tan^{-1}(I/R)$ (rad)	$\left 1-\frac{f_{Ga}f'_{As}}{f'_{Ga}f_{As}}\right $
$\begin{matrix} 5\ \bar{1}\ 7 \\ 3\ 9\ \bar{7} \end{matrix}$	0.0388 0.0525	0.0413 0.0555	$4.33 \times 10^{-2}$	$1.5 \times 10^{-4}$	$3.4 \times 10^{-3}$	0.007
$\begin{matrix} 7\ \bar{1}\ 5 \\ 5\ 9\ \bar{5} \end{matrix}$	0.0525 0.0549	0.0555 0.0580	$6.10 \times 10^{-2}$	$-2.0 \times 10^{-5}$	$-3.2 \times 10^{-4}$	0.001
$\begin{matrix} 9\ 3\ 7 \\ 11\ \bar{5}\ \bar{7} \end{matrix}$	0.0525 0.0388	0.0555 0.0413	$4.30 \times 10^{-2}$	$-1.5 \times 10^{-4}$	$-3.4 \times 10^{-3}$	0.007

Table (b) ZnS

$\begin{matrix} hkl \\ 2-h, \bar{2}-k, \bar{l} \end{matrix}$	$f_{Zn}(nm)$	$f_S(nm)$	$R=f_{Zn}f'_{Zn}+f_Sf'_S$	$I=f'_{Zn}f_S-f_{Zn}f'_S$	$\tan^{-1}(I/R)$ (rad)	$\left 1-\frac{f_{Zn}f'_S}{f'_{Zn}f_S}\right $
$\begin{matrix} 5\ \bar{1}\ 7 \\ 3\ 9\ \bar{7} \end{matrix}$	0.0352 0.0263	0.0200 0.0263	$2.19 \times 10^{-2}$	$2 \times 10^{-4}$	$1 \times 10^{-2}$	0.024
$\begin{matrix} 7\ \bar{1}\ 5 \\ 5\ 9\ \bar{5} \end{matrix}$	0.0352 0.0500	0.0200 0.0276	$2.31 \times 10^{-2}$	$3 \times 10^{-4}$	$1 \times 10^{-2}$	0.029
$\begin{matrix} 9\ 3\ 7 \\ 11\ \bar{5}\ \bar{7} \end{matrix}$	0.0474 0.0352	0.0263 0.0200	$2.19 \times 10^{-2}$	$-2 \times 10^{-4}$	$1 \times 10^{-2}$	0.024

# Spurious $m_2$



[111]

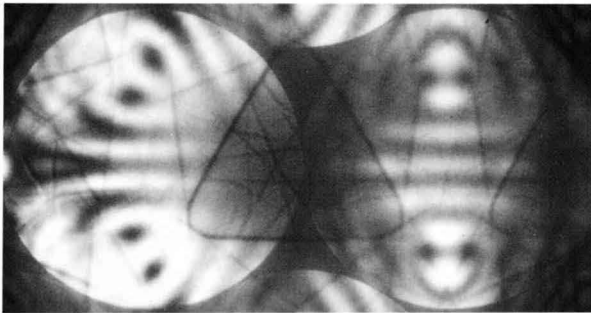
000

$2\bar{2}0$

100 kV

Ge

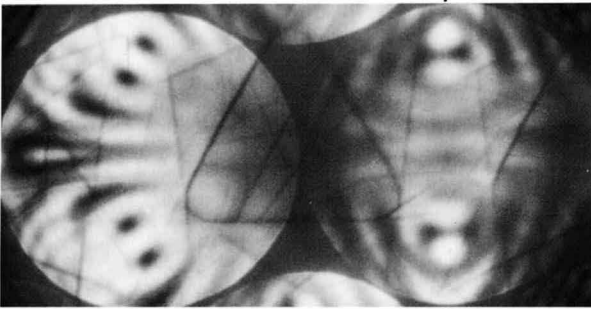
$m3m$



$m_2$

GaAs

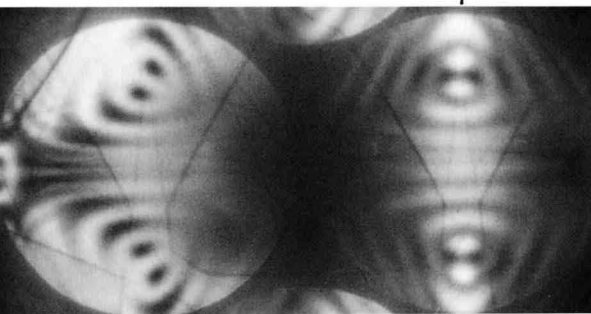
$\bar{4}3m$



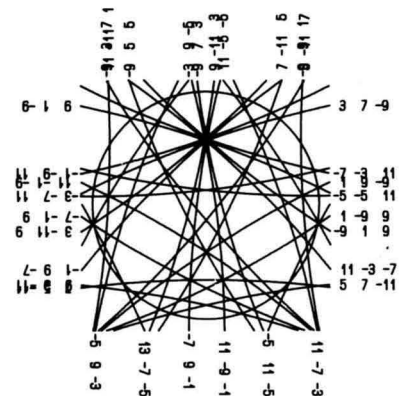
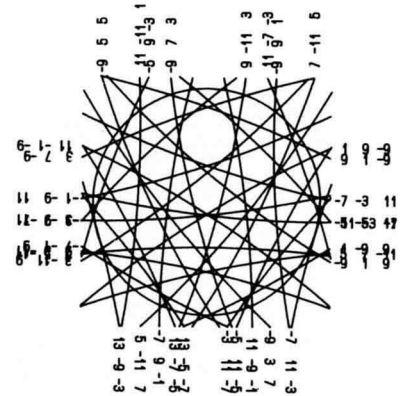
$m_2$

ZnS

$\bar{4}3m$



$m_2$

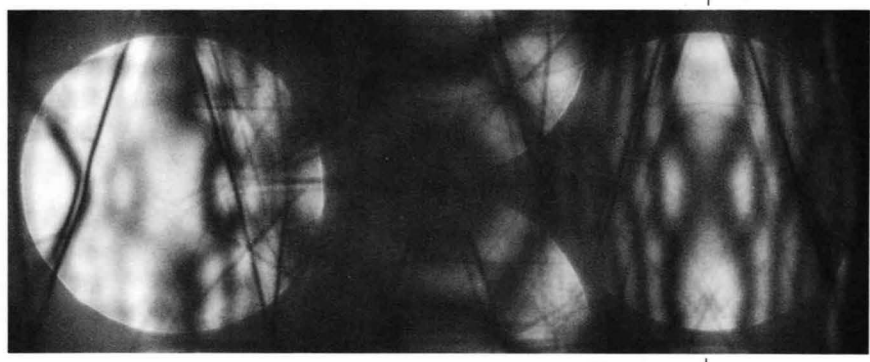


The  $2\bar{2}0$  reflection was exactly excited in each photograph. A true symmetry  $m_2$  from Ge is shown for comparison.



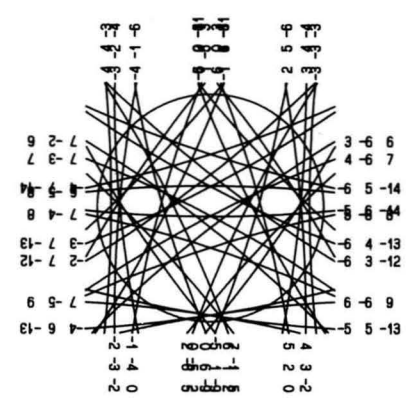
SiC-15R  $[1\bar{1}01]$

100 kV

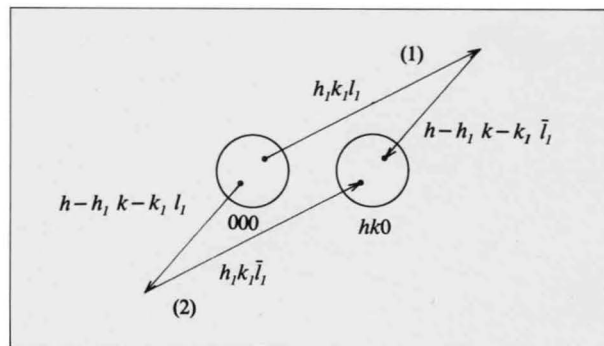
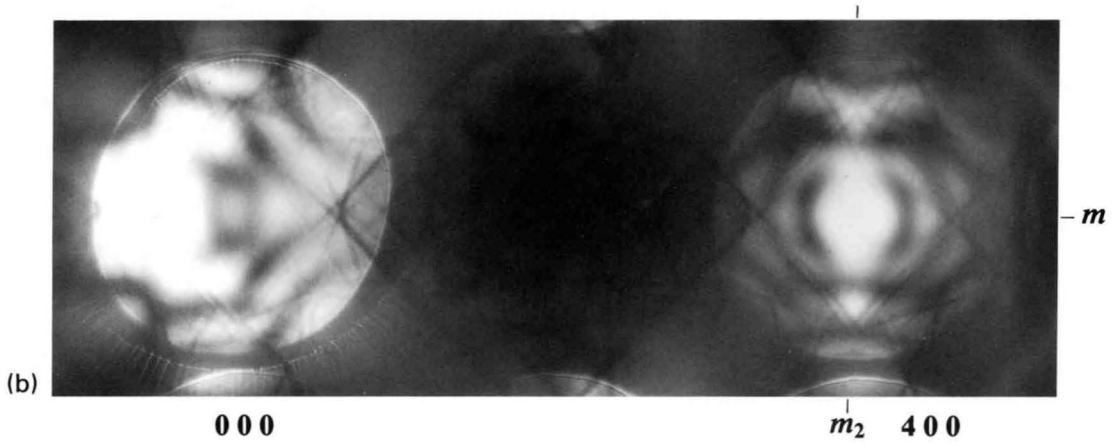
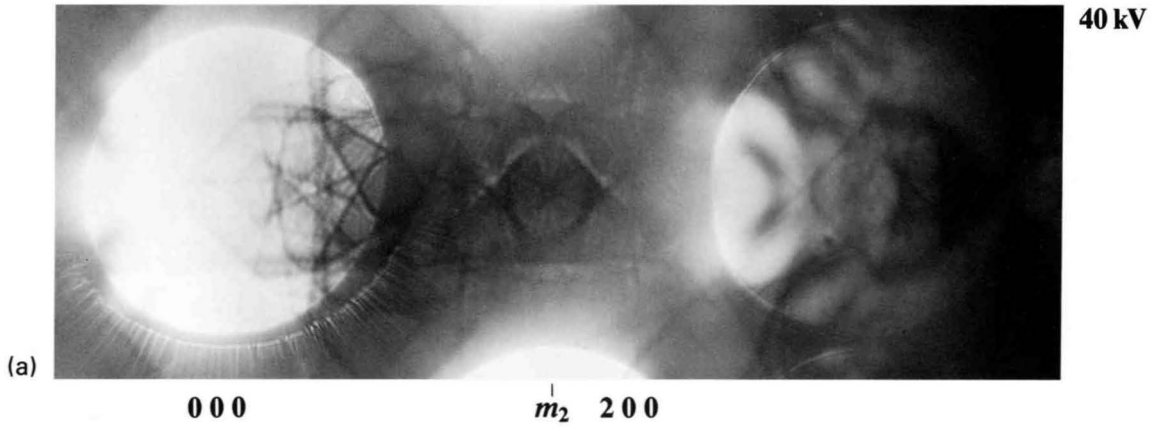
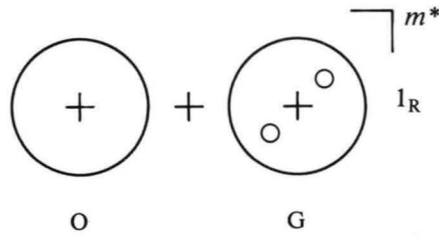


0000

$m_2$  1120



**Spurious  $1_R$**   
**InAs [001]**



Double reflection paths forming a symmetry  $1_R$

InAs also has a zinc-blende type structure. Dark-field patterns of the 200 and 400 reflections taken at the [001] incidence show symmetries  $m_2$  and  $2mm$ , respectively. The symmetry  $m_2$  is a correct symmetry expected from the twofold axis in the [100] direction. However, the symmetry  $2mm$  in the 400 reflection is caused by the addition of a spurious symmetry  $1_R$ .

Double reflection paths (1) and (2) which form a symmetry  $1_R$  are shown in the figure. Table (a) gives the expressions of  $H(h_1k_1l_1)$  and  $H(h_1k_1\bar{l}_1)$  for four different cases about the sum of reflection indices. When the table is referred to by considering the lattice type of InAs to be face-centered cubic and the resultant reflection to be of  $hk0$  ( $h, k = \text{even}$ ), the following relations are obtained:

$$\begin{aligned}\hat{H}_2^{(1)} &= \hat{H}_2^{(2)} & \text{for } h_1 + k_1 + l_1 &= 4n, 4n+2 \\ \hat{H}_2^{(1)} &= (\hat{H}_2^{(2)})^* & \text{for } h_1 + k_1 + l_1 &= 4n+1, 4n+3\end{aligned}$$

As a result, a spurious symmetry  $1_R$  occurs for the double reflection paths of  $000 \rightarrow 2N\text{th Laue zone} \rightarrow hk0$  ( $l_1 = 2N$ ). It also occurs for the paths of  $000 \rightarrow (2N+1)\text{th Laue zone} \rightarrow hk0$  ( $l_1 = 2N+1$ ), if  $\hat{H}_2^{(1)}$  is real.

Table (b) shows combinations of two types of reflections for each of two cases of the resultant reflection  $hk0$ . For  $h+k=4n+2$ , the imaginary part of  $\hat{H}_2^{(1)}$  is neither zero nor small. Therefore, no spurious symmetry occurs, for instance, in the 200 dark-field pattern (a). For  $h+k=4n$ , a spurious symmetry  $1_R$  appears when  $f'_A/f_A \cong f'_B/f_B$ , for instance, in the 400 reflection (b). The observation shows a good agreement with theoretical analysis. Computer simulation also proved quantitatively the occurrence of the spurious symmetry.

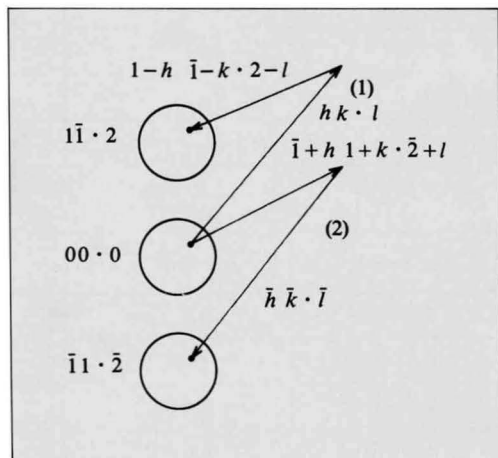
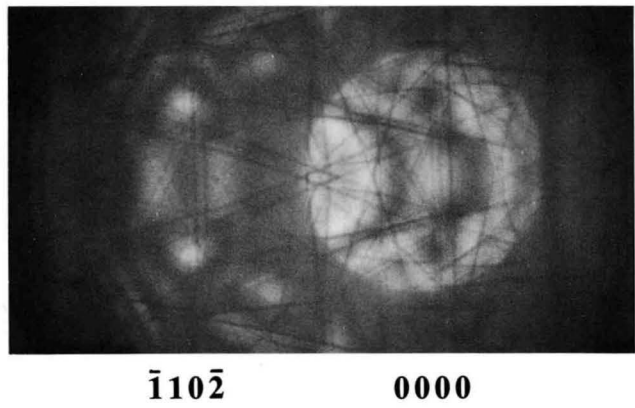
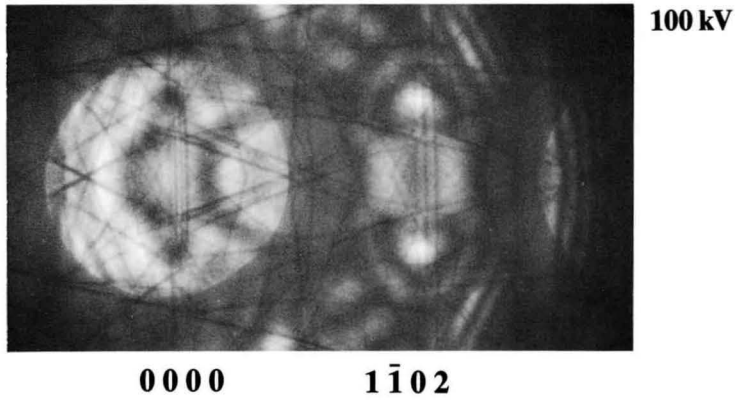
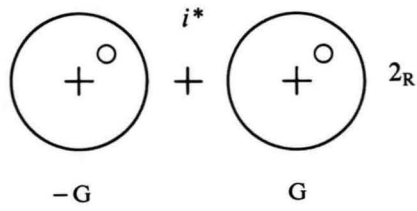
Table (a)

$h_1+k_1+l_1$	$H(h_1k_1l_1)$	$l_1$	$h_1+k_1-l_1$	$H(h_1k_1\bar{l}_1)$
$4n$	$f_A + f_B$	$2m$	$4n'$	$f_A + f_B$
$4n+1$	$f_A + if_B$	$2m+1$	$4n'+3$	$f_A - if_B$
$4n+2$	$f_A - f_B$	$2m$	$4n'+2$	$f_A - f_B$
$4n+3$	$f_A - if_B$	$2m+1$	$4n'+1$	$f_A + if_B$

Table (b)

$h+k$	$h_1+k_1+l_1$	$(h-h_1)+(k-k_1)-l_1$	$H_2 = H(h_1k_1l_1) \cdot H(h-h_1, k-k_1, -l_1)$
$4n$	$4n+1$	$4n+3$	$(f_A \pm if_B)(f_A' \mp if_B') = f_A f_A' + f_B f_B' \pm i(f_A' f_B - f_A f_B')$
	$4n+3$	$4n+1$	
$4n+2$	$4n+1$	$4n+1$	$(f_A \pm if_B)(f_A' \pm if_B') = f_A f_A' - f_B f_B' \pm i(f_A' f_B + f_A f_B')$
	$4n+3$	$4n+3$	

**Spurious  $2_R$**   
**SiC-15R  $[1\bar{1}0\bar{1}]$**



Double reflection paths forming a symmetry  $2_R$ .

SiC-15R belongs to a noncentrosymmetric space group  $R3m$ . The whole structure lacks an inversion center whereas the substructure has one. No symmetry is expected between a pair of  $\pm G$  dark-field patterns from the whole structure. The observed symmetry  $2_R$  between the  $1\bar{1}02$  and  $\bar{1}10\bar{2}$  reflections at the  $[1\bar{1}0\bar{1}]$  incidence must have originated from an inversion center of the substructure.

Double reflection paths (1) and (2) which form a symmetry  $2_R$  are shown in the figure.  $G$ , which originates from the substructure, is real.  $\hat{H}_1^{(1)}$  is equal to  $(\hat{H}_1^{(2)})^*$ , because of the lack of centrosymmetry.  $\hat{H}_2^{(1)}$  is equal to  $(\hat{H}_2^{(2)})^*$  (eq. (7)). When the phases of  $\hat{H}_1^{(1)}$  and  $\hat{H}_2^{(1)}$  are the same,  $F^{(1)}$  and  $F^{(2)}$  becomes the same in their magnitudes and different only in their phases, resulting a spurious symmetry  $2_R$ . The phase  $\theta$  of  $\hat{H}_1^{(1)}$  was calculated to be 0.221 rad for the  $1\bar{1}02$  reflection. The table show the phase  $\theta'$  of  $\hat{H}_2^{(1)}$  and the phase difference  $\theta' - \theta$  for several double reflections. Although the values of about  $2 \times 10^{-1}$  rad for the three lower cases look rather large, experimental results show a spurious symmetry  $2_R$ . It is noted that the symmetry  $2_R$  was not observed between the  $2\bar{2}04$  and  $220\bar{4}$  reflections at the  $[1\bar{1}0\bar{1}]$  incidence, at which a pair of double reflection paths had a phase difference of about 0.6 rad. Computer simulation proved quantitatively the occurrence of the spurious symmetry between the  $1\bar{1}02$  and  $\bar{1}10\bar{2}$  reflections.

$\begin{matrix} h & k & l \\ 1-h & 1-k & 2-l \end{matrix}$	$f_{Si}(\text{nm})$	$f_C(\text{nm})$	$R=f_{Si}f_{Si}+f_Cf_C$	$I=f_{Si}f_C-f_{Si}f_C$	$\theta'=\tan^{-1}(I/R)$ (rad)	$\theta' - \theta$ (rad)
$\begin{matrix} 2 & \bar{1} & 3 \\ \bar{1} & 0 & \bar{1} \end{matrix}$	0.1364 0.2793	0.0829 0.1541	$8.20 \times 10^{-2}$	$1.98 \times 10^{-2}$	0.236	0.015
$\begin{matrix} 1 & 0 & 1 \\ 0 & \bar{1} & 1 \end{matrix}$	0.2793 0.2793	0.1541 0.1541	$1.79 \times 10^{-1}$	$4.06 \times 10^{-2}$	0.223	0.001
$\begin{matrix} \bar{1} & \bar{5} & 7 \\ 2 & 4 & \bar{5} \end{matrix}$	0.0252 0.0272	0.0109 0.0118	$6.15 \times 10^{-4}$	$1.8 \times 10^{-5}$	0.029	-0.192
$\begin{matrix} \bar{6} & 2 & \bar{5} \\ 7 & \bar{3} & 7 \end{matrix}$	0.0272 0.0217	0.0118 0.0093	$5.3 \times 10^{-4}$	$1.3 \times 10^{-5}$	0.025	-0.196
$\begin{matrix} 6 & \bar{6} & 15 \\ \bar{5} & 5 & \bar{1}3 \end{matrix}$	0.0218 0.0293	0.0094 0.0128	$5.72 \times 10^{-4}$	$2.1 \times 10^{-5}$	0.037	-0.184

$\theta=0.221$  rad

# SiC-10H

The space group of SiC-10H is  $P3m1$ , projections of the structure being depicted schematically in Fig. (a). X-ray diffraction identified the point group of this substance to be  $6/mmm$  instead of  $3m$  (Fig. (b)). This phenomenon is called Ramsdell-type symmetry enhancement. From the symmetries of CBED patterns, the diffraction and point groups were identified to be  $3m1_R$  and  $\bar{6}m2$  at the  $[0001]$  incidence (Table (a)), and  $m1_R$  and  $6mm$  at the  $[1\bar{1}00]$  incidence (Table (b)). These inconsistent results originate from spurious symmetries. CBED symmetries expected from the true point group  $3m$  are given in the tables as a reference.

$H$  and  $G$  of SiC-10H are expressed as

$$H(\mathbf{h}) = f_{\text{Si}} + f_{\text{C}} \exp 2\pi i \left( \frac{3}{40} \right) l$$

$$G(\mathbf{h}) = \sum_j^{10} \exp 2\pi i \mathbf{h} \cdot \mathbf{r}_j, \quad (1)$$

where  $\mathbf{h} = hki l$ .

The kinematical structure factors satisfy the relations,

$$F(hki\bar{l}) = H^*(hki l)G(hki l) \quad (2)$$

$$F(\bar{h}\bar{k}\bar{l}) = H(hki l)G^*(hki l) \quad (3)$$

$$F(h+k \bar{k}\bar{h}\bar{l}) = H^*(hki l)G(hki l) \quad (4)$$

Equation (2) indicates that a pseudo mirror plane  $m^*$  exists perpendicular to the  $[0001]$ . The pseudo horizontal and vertical mirror planes always produce a spurious symmetry  $1_R$  and  $m_v$  in the bright-field pattern. These symmetries are, however, hidden in usual cases due to the existence of a true vertical and horizontal twofold rotation axes perpendicular to the corresponding pseudo mirror planes as shown in Fig. (c). In the present case, instead a true twofold axis, a pseudo twofold axis (eq. (3) and

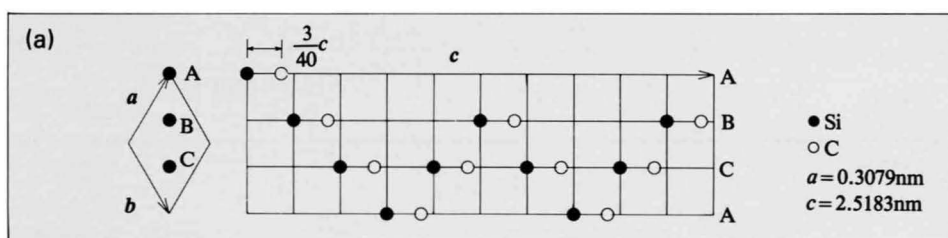
Fig. (d)) exists perpendicular to a pseudo mirror plane (eq. (2)), owing to a very special arrangement of Si and C. The symmetry due to the pseudo mirror plane causes the symmetries  $6mm$  and  $2mm$  in the bright-field pattern at the  $[0001]$  incidence (Photo (a)) and  $[1\bar{1}00]$  incidence (Photo (d)), instead of the symmetries  $3m$  and  $m$ , respectively.

The substructure has a twofold axis in the  $[10\bar{1}0]$  direction, although the whole structure does not (eq. (4)). As a result, in the  $10\bar{1}0$  and  $\bar{1}010$  dark-field patterns (b) and (c) taken at the  $[0001]$  incidence, a spurious symmetry  $m_2$  is added perpendicular to the true symmetry  $m$ , resulting in a symmetry  $2mm$ . This spurious symmetry is of the same type as that observed in ZnS, GaAs and SiC-15R. The symmetry  $m_2$  in the symmetry  $2mm$  of the  $00010$  and  $000\bar{1}0$  dark-field patterns (e) and (f) is also a spurious one. This spurious symmetry, however, does not originate from the symmetry of the substructure, because the substructure has no twofold axis in the  $[0001]$  direction ( $G(\bar{h}\bar{k}\bar{l}) \neq G(hki l)$  in eq. (3)). It is caused by a pseudo twofold axis in the whole structure, and originates from the special atomic arrangements in SiC-10H.

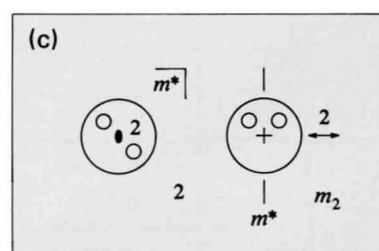
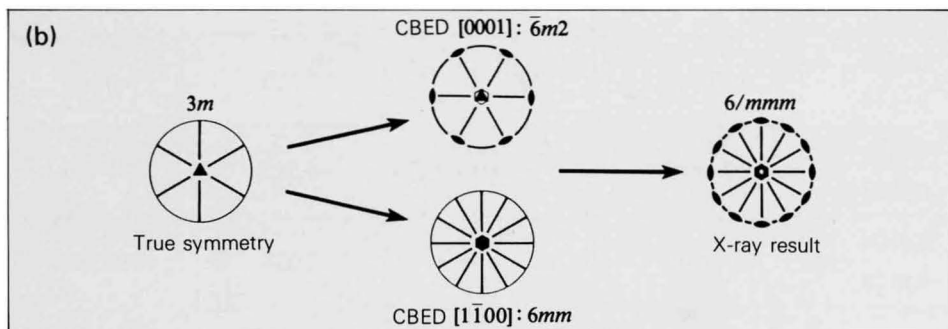
The specimen was supplied by Z. Inoue of the National Institute for Research in Inorganic Materials of Japan.

## References

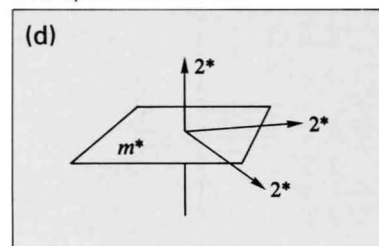
- [a] L.S. Ramsdell and J.A. Kohn: *Acta Cryst.*, **4** (1951) 111.
- [b] M. Tanaka, H. Sekii, O. Ueno and H. Takayoshi: *Acta Cryst.*, **A40** Suppl. (1984) C384.



Projection of the structure of SiC-10H.

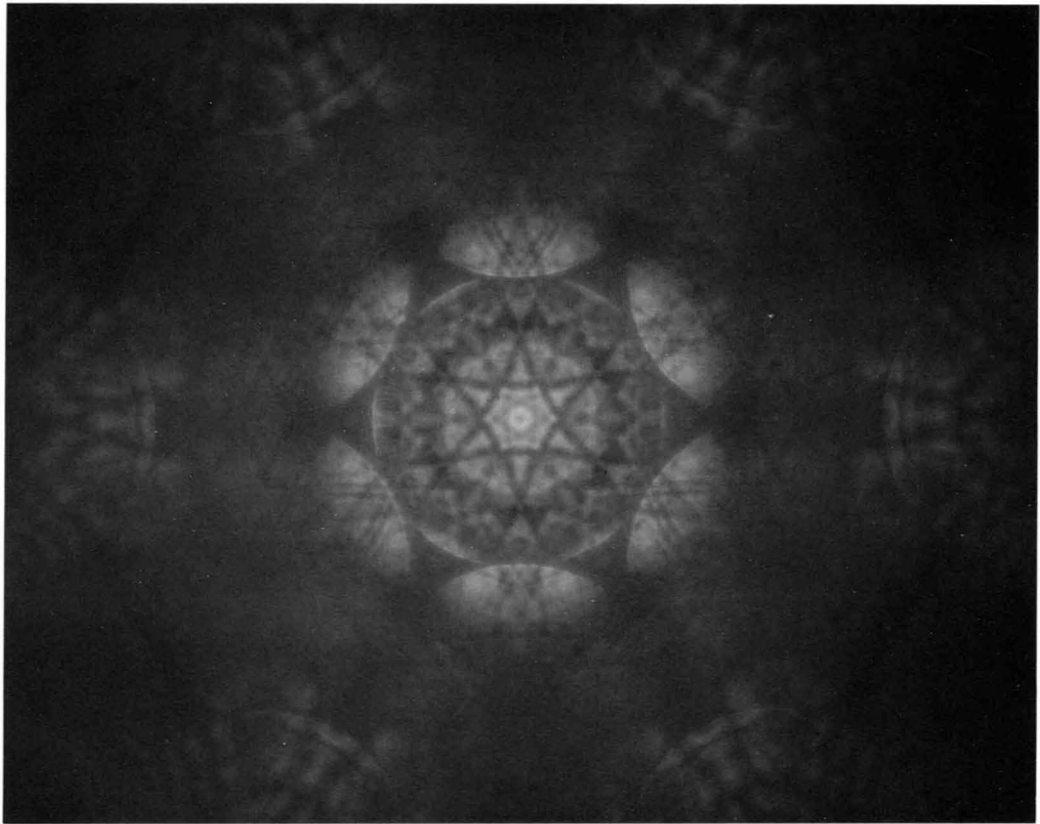


Spurious symmetries are hidden by true symmetries in BP.



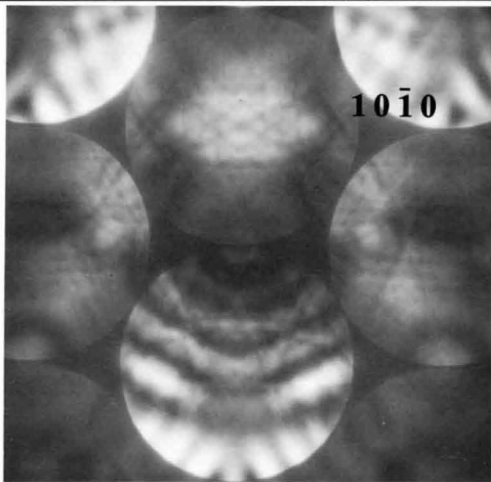
Pseudo symmetry elements of SiC-10H.

**[0001]**



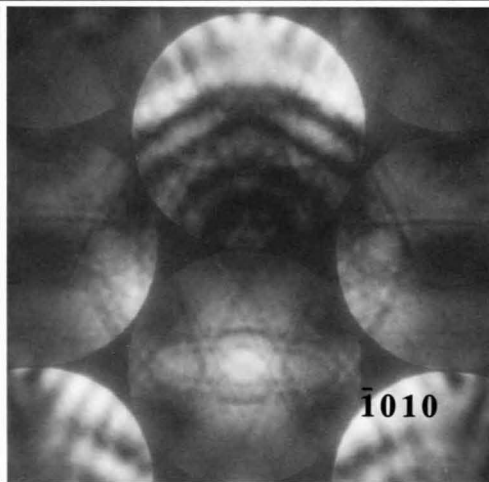
**80 kV**

(a)



**10 $\bar{1}$ 0**

(b)



**$\bar{1}$ 010**

(c)

**100 kV**

**Table (a)**

Incidence	Point Group	Diffraction Group	BP	WP	DP	$\pm$ DP
[0001]	$\bar{6}m2$ (exp.)	$3m1_R$	$6mm$	$3m_v$	$2m_v m_2$	1
	$3m$ (true)	$3m$	$3m_v$	$3m_v$	$m_v$	1

SiC-10H

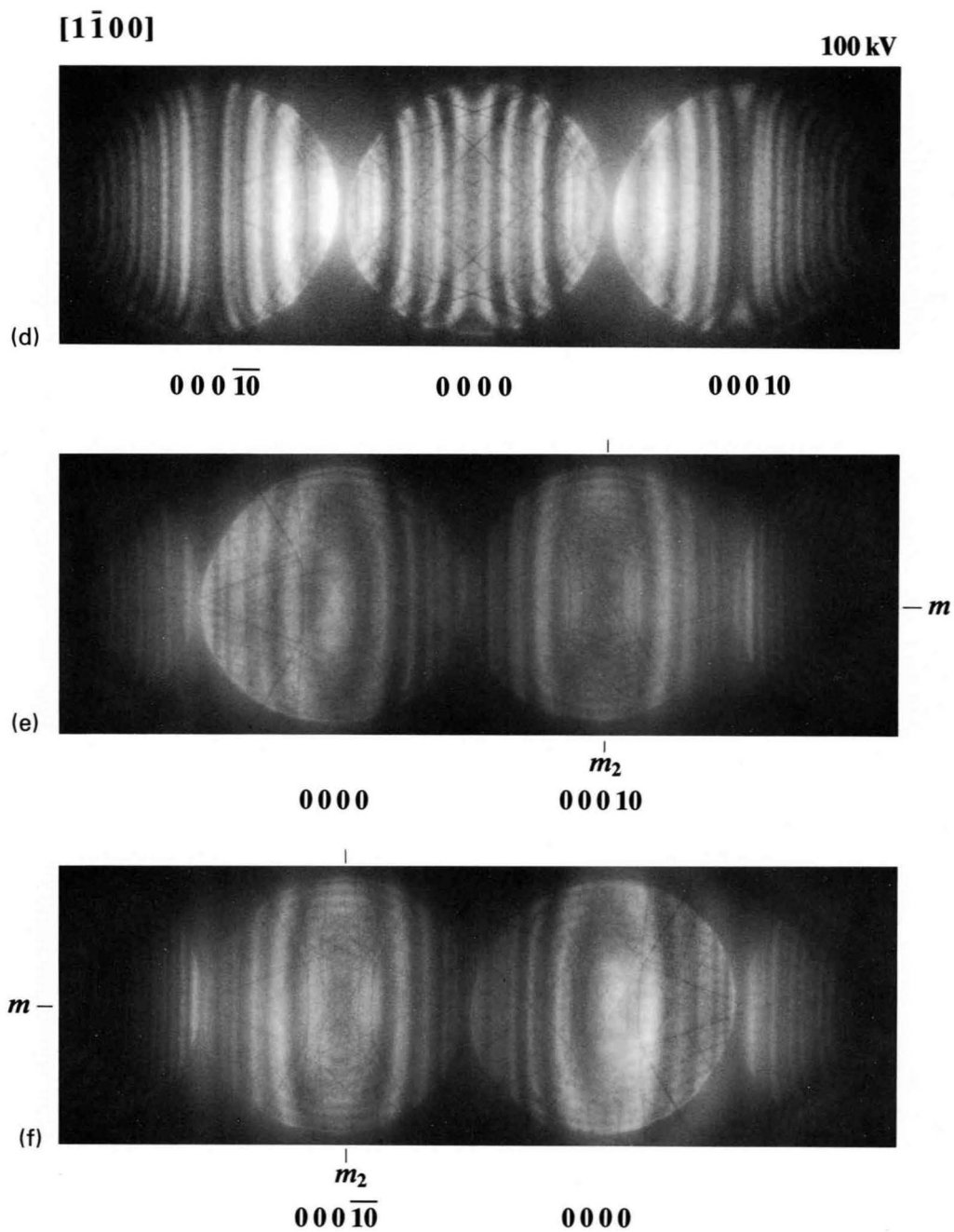


Table (b)

Incidence	Point Group	Diffraction Group	BP	WP	DP	$\pm$ DP
[1 $\bar{1}$ 00]	6mm (exp.)	$m1_R$	2mm	$m_v$	$2m_v m_2$	—
	3m (true)	$m$	$m_v$	$m_v$	$m_v$	1

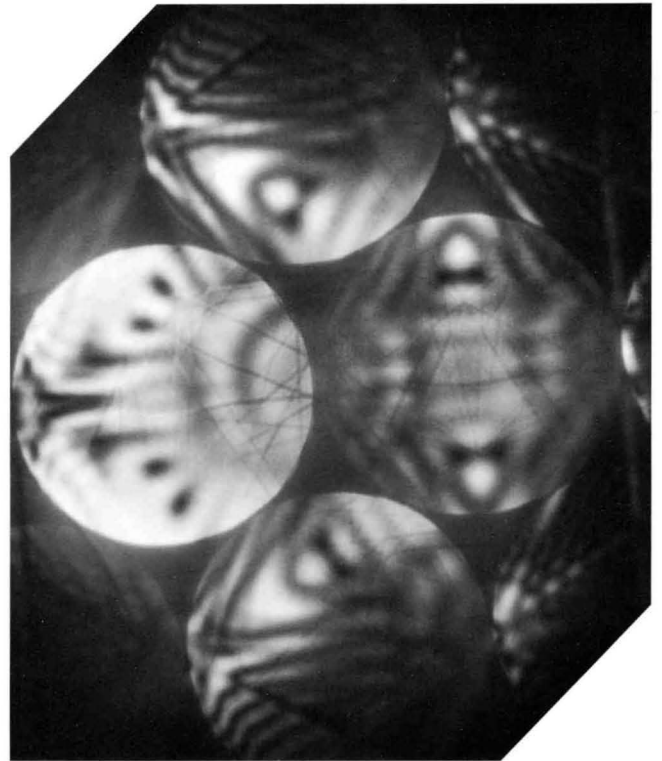
## *Symmetry Due to Twofold Axes Oblique to Specimen Surfaces*

When the theory of Buxton *et al.* [1] is accepted in a strict sense, CBED observes the symmetry elements of diperiodic plane figures. Then, for example, a twofold rotation axis oblique to the specimen surface is not a symmetry element of diperiodic plane figures. The two photographs shown were taken at the 220 Bragg settings with the [111] incidence by tilting a Si film with the [100] surface normal. Symmetries of  $m_2$  due to twofold axes are clearly seen. At least one of the twofold axes is oblique to the specimen surface. Important for CBED is that the top and bottom surfaces be parallel over a specimen area illuminated with the incident beam. It is not necessary to stick so much to whether symmetry elements of a crystal are those of diperiodic plane figures. CBED observes symmetries of a crystal, as far as the boundary condition does not break symmetries of CBED patterns. Gjønnnes and Gjønnnes [a] reported that the breaking of symmetries due to the surface set oblique to the incident beam is practically negligible. We can tilt a parallel-sided specimen to find crystal symmetry elements oblique to the surface.

The reader will later see on pages 51 to 61 symmetries of CBED patterns produced from crystal symmetry elements which do not belong to those of diperiodic plane figures.

Si

100 kV



### Reference

- [a] J. Gjønnnes and K. Gjønnnes: *Ultramicroscopy*, **18** (1985) 77.

# *Space-Group Determination*

# GM Lines Due to Horizontal Glide Planes

Dynamical extinction lines or GM lines [7] have been successfully utilized for the identification of screw axes and glide planes [8]. The table on the opposite page shows the extinction rules given by Gjønnes and Moodie [7]. The dynamical extinction due to a glide plane which is set perpendicular to the incident beam has been predicted to appear as a dark spot at the exact Bragg position of a kinematically forbidden reflection. However, this extinction had not been observed until recently. The observation of the extinction was reported for the 420 reflection of spinel ( $\text{MgAl}_2\text{O}_4$ ) and the 200 reflection of silicon (Si) [a]. On the basis of the experimental results, the extinction rule given by Gjønnes and Moodie has been modified in a practical manner.

Spinel belongs to the space group of  $F4_1/d\bar{3}2/m$ . The  $d$ -glide planes of this space group lie parallel to the  $\{100\}$  planes. Owing to the glide planes, the reflections with indices  $h+k=4n+2$  (cyclic) are kinematically forbidden. The dynamical extinction due to the (001)  $d$ -glide plane set perpendicular to the incident beam is expected to appear in the 420 reflection ( $n=1$ ).

Figure (a) schematically illustrates low-order 0th Laue-zone reflection disks and Umweganregung paths to the 420 reflection for the [001] incidence. The 020, 400 and 420 reflections are set simultaneously at the exact Bragg condition. Thus, the projection of the Laue point along the [001] direction is located at the 210 Bragg position and denoted by the letter L. The 420 reflection occurs due to Umweganregung via HOLZ reflections. The paths A and B are symmetric with respect to the point L. The two beams coming through these paths meet on the 420 reflection, and lose their intensity because of their phase difference  $\pi$ . To obtain a spot-shaped extinction, several pairs of HOLZ lines running in different directions have to meet near the exact Bragg position. To produce this situation, the accelerating voltage must be set to a certain value.

Figure (b) shows HOLZ reflections excited at 50.0 kV. Four pairs of Umweganregung paths are depicted. The computer simulated pattern added to Photo (a) on page 38 shows HOLZ reflection lines appearing in the 420 reflection disk. Two HOLZ lines corresponding to a pair of paths, A and B, are almost superposed in a certain angular range with the exact excitation position as the center. Such four superposed lines cross at the center of the disk.

Photograph (a) shows a CBED pattern taken from a (001) spinel specimen with an accelerating voltage of 50.0 kV at the Liq.  $\text{N}_2$  temperature to enhance the intensity of HOLZ lines. The extinction is seen to occur not only at the exact excitation position but also in a certain angular range along the HOLZ line pairs, thus forming dark lines instead of a spot-shaped extinction at the exact excitation position [7]. This result is due to the fact that

each pair of parallel lines loses its intensity in the overlapping region and other intense HOLZ lines do not intersect or disturb the pair lines over a certain angular range around the exact excitation position.

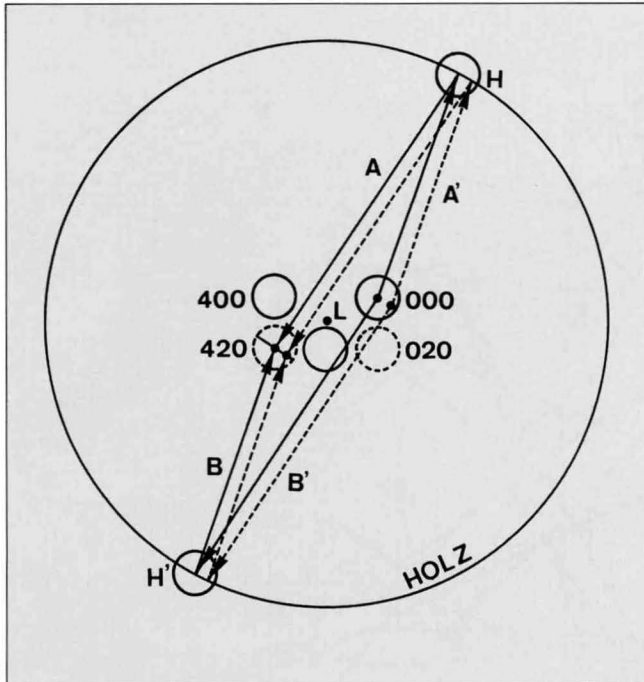
On the basis of such experimental facts, the extinction rule has been modified as follows: *The extinction occurs as dark lines crossing each other at the exact excitation position.*

When the accelerating voltage is increased by 0.5 kV to 50.5 kV, a spot-shaped extinction is seen over a small angular range with the exact excitation position as the center. This may be a direct proof of the prediction of Gjønnes and Moodie [7]. However, in order to observe a spot-shaped extinction, special attention must be paid to the very careful adjustment of the accelerating voltage.

A similar extinction is also seen in the 020 reflection. Consider two Umweganregung paths to the 020 reflection via HOLZ reflections H and H' in Fig.(a). The HOLZ line geometry in the 020 disk is the same as in the 420 disk. The phases of the two paths differ by an integral multiple of  $2\pi$  from those of the paths A and B, since the two paths are created by subtracting the vector of the 400 reflection from the paths A and B. Hence, the sign of the resultant structure amplitude remains opposite between the two paths, although its magnitude is now different between the two. Therefore, imperfect cancellation still takes place between the two beams. If the difference between the magnitudes is small, an extinction similar to that in the 420 disk also occurs in the 020 disk. This is the origin of the extinction observed in the 020 reflection. The reader is referred to the section of spurious  $B_3$  GM lines.

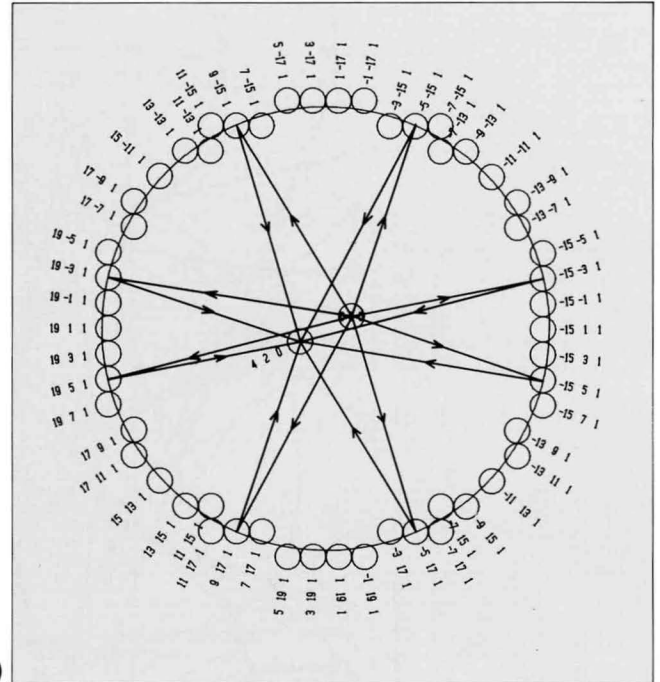
## Reference

- [a] M. Tanaka, M. Terauchi and H. Sekii: *Ultramicroscopy*, **21** (1987) 245.



(a)

The 420 reflection occurs due to Umweganregung via HOLZ reflections. The paths A and B are symmetric with respect to the point L.



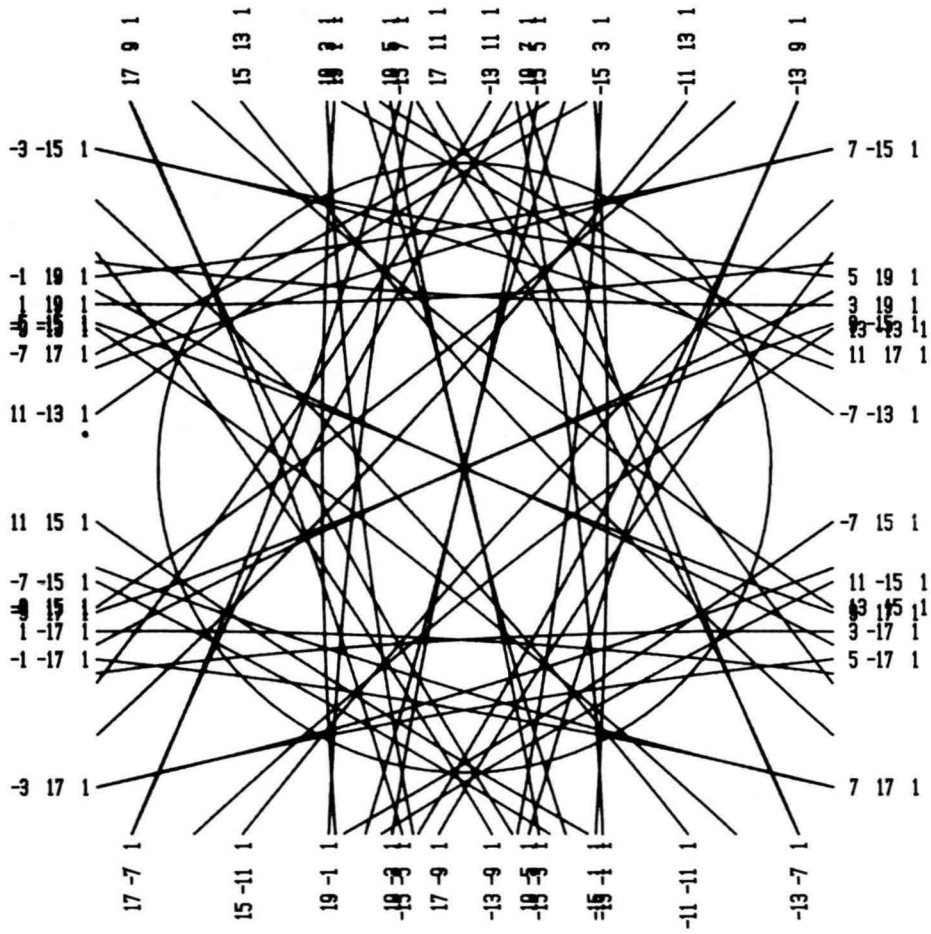
(b)

Simulation of HOLZ reflections of spinel excited at [001] electron incidence and 50.0 kV accelerating voltage. Four pairs of Umweganregung paths to the 420 reflection are drawn.

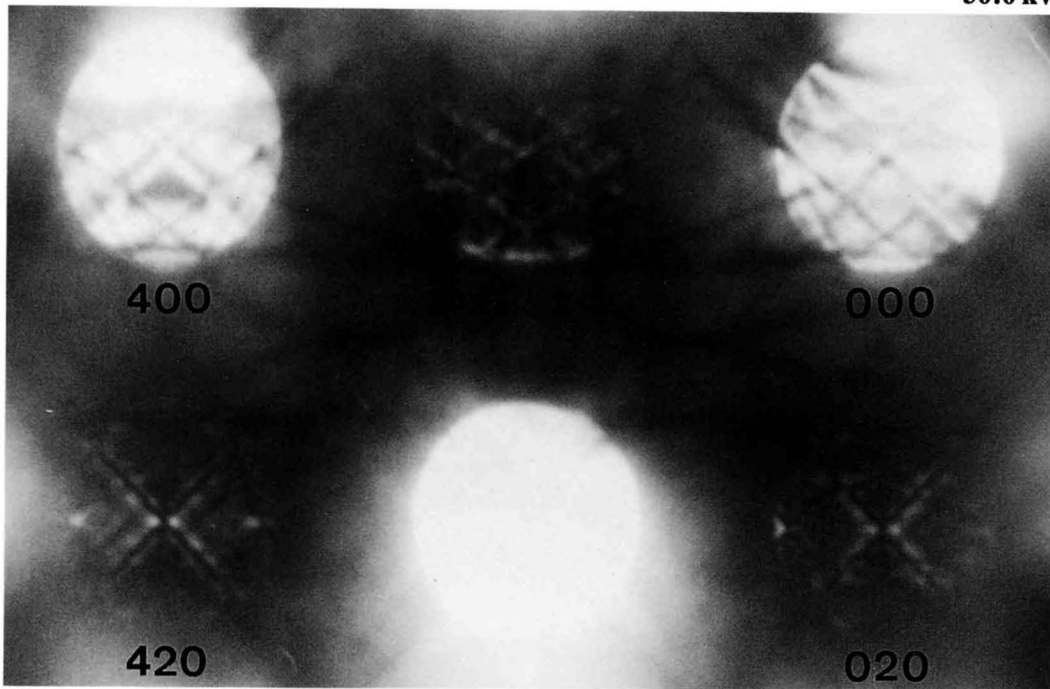
#### Dynamical extinction rules for symmetry elements of a parallel-sided specimen

Symmetry elements of parallel-sided specimen	Orientation to specimen surface	GM lines	
		Two-dimensional (ZOLZ) interaction	Three-dimensional (HOLZ) interaction
Glide planes	Perpendicular: $g$	$A_2$ and $B_2$	$A_3$
	Parallel: $g'$	—	Intersection of $A_3$ and $B_3$
Twofold screw axes	Parallel: $2_1'$	$A_2$ and $B_2$	$B_3$

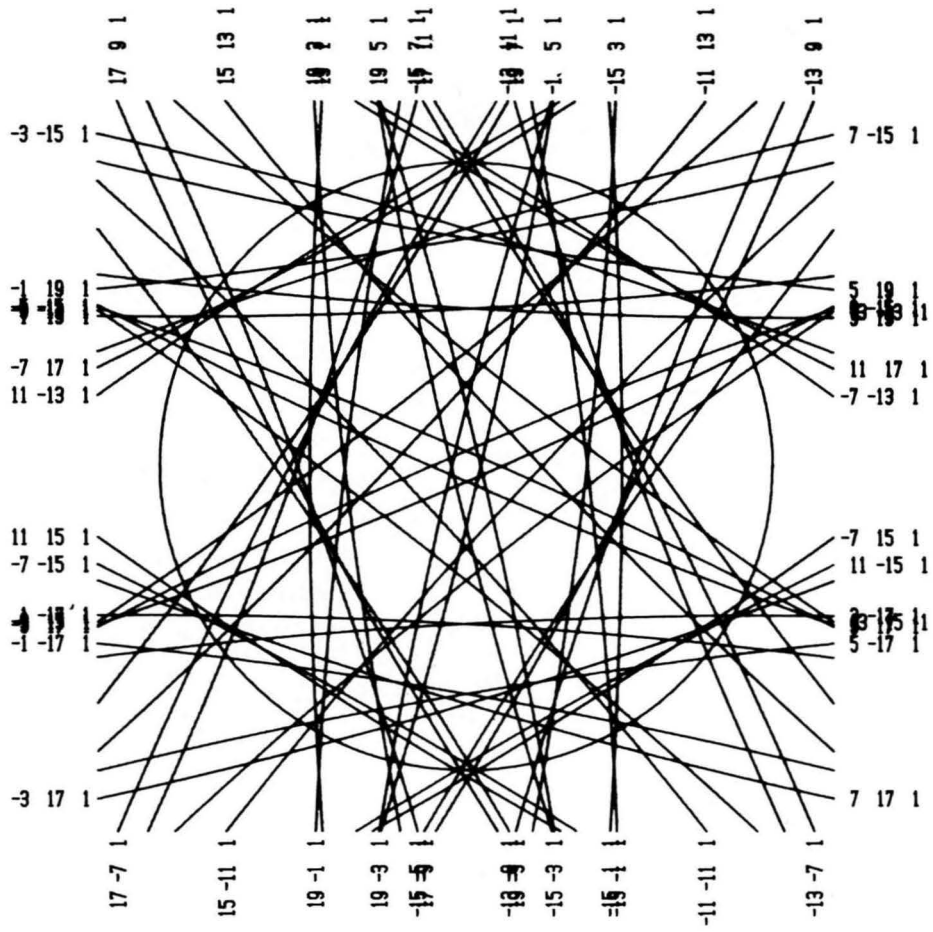
$\text{MgAl}_2\text{O}_4$  [001]



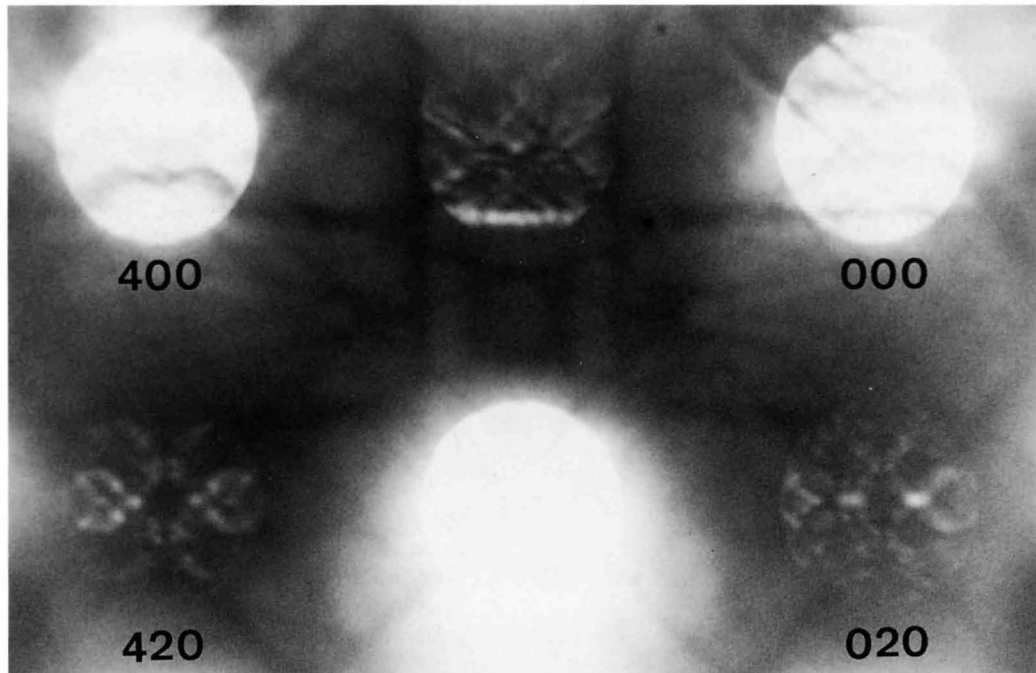
50.0 kV



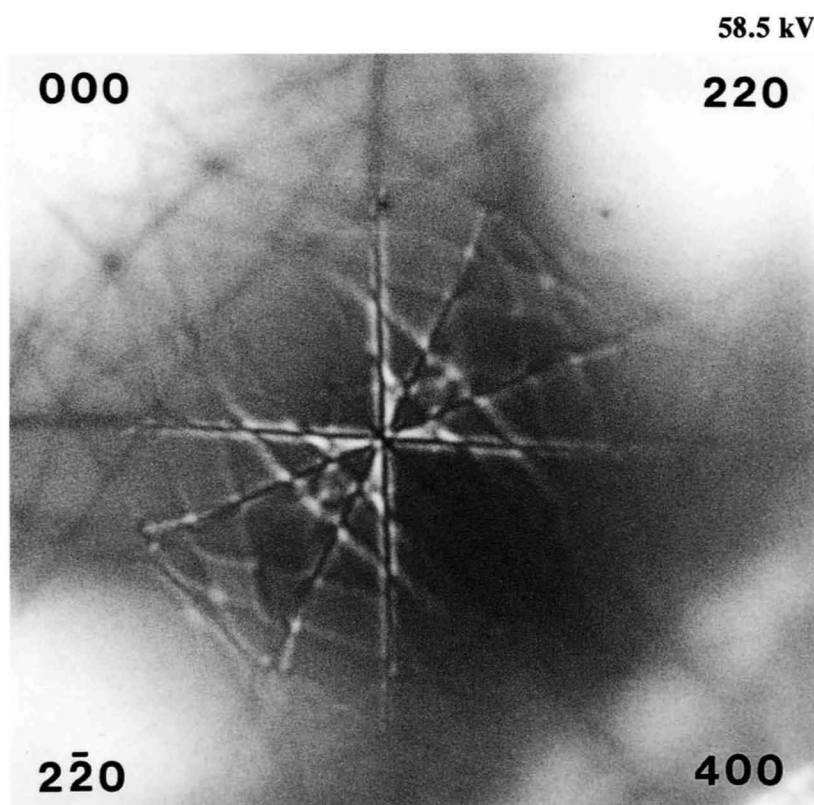
(a)



50.5 kV



(b)



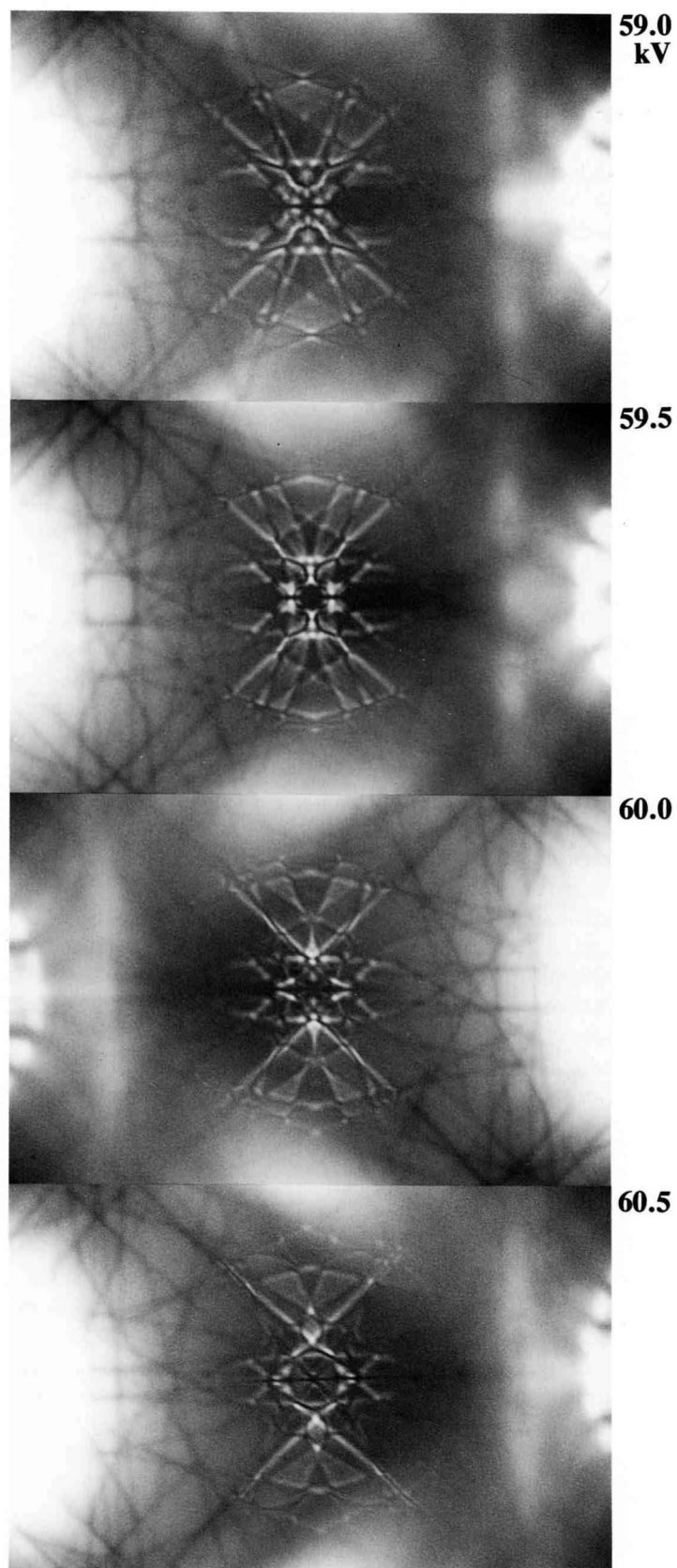
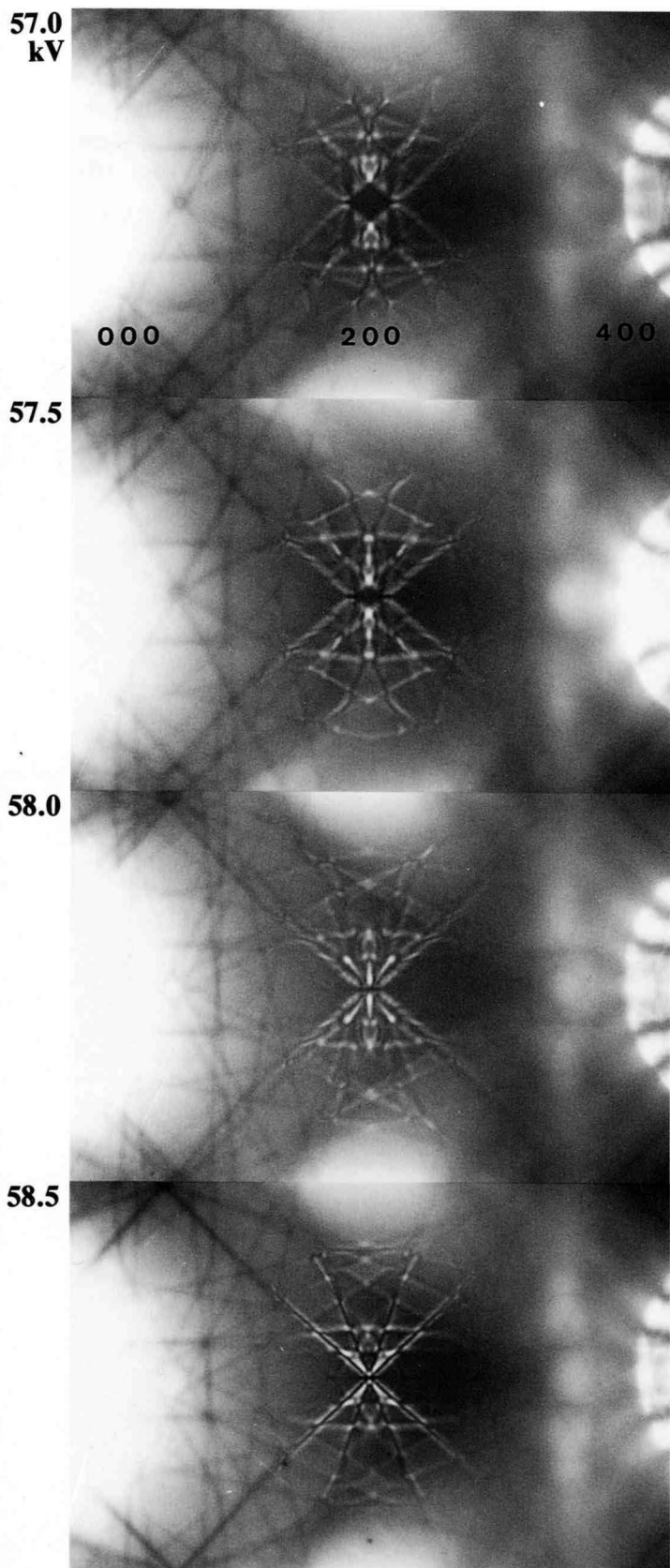
The dynamical extinction lines due to the (001)  $d$ -glide plane crossing at the exact 200 Bragg position.

The above photograph shows a pattern taken from (001) Si with the [001] incidence at an accelerating voltage of 58.5 kV.

The dark lines skewed to the [100] direction clearly cross at the exact excitation position of the 200 reflection. This proves the existence of the (001)  $d$ -glide plane.

In the reflection, an extinction due to the (010)  $d$ -glide plane is also expected to appear. However, the extinction line in the [100] direction due to this glide plane is not clear, because no HOLZ line appears in this direction at this accelerating voltage.

▶ A series of photographs on the opposite page shows 200 dark-field patterns taken from (001) Si with the [001] incidence at successive accelerating voltages. Not only GM lines due to a horizontal (001)  $d$ -glide plane but also the lines in the [100] direction due to a vertical (010)  $d$ -glide plane are seen.



Accelerating-voltage dependence of GM lines due to a horizontal and a vertical  $d$ -glide plane.

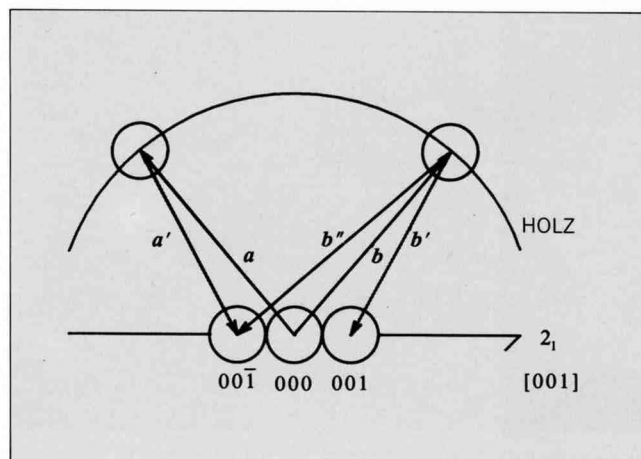
## Spurious $B_3$ GM Lines

When a  $2_1$  screw axis is set perpendicular to the incident beam,  $A_2$  GM lines are observed in kinematically forbidden reflections and  $B_2$  and  $B_3$  GM lines in exactly excited forbidden reflections. However, extinctions similar to  $B_3$  GM lines are sometimes observed in forbidden reflections at the symmetric incidence and at incidences exciting kinematically allowed reflections. We call these extinction lines spurious  $B_3$  GM lines.

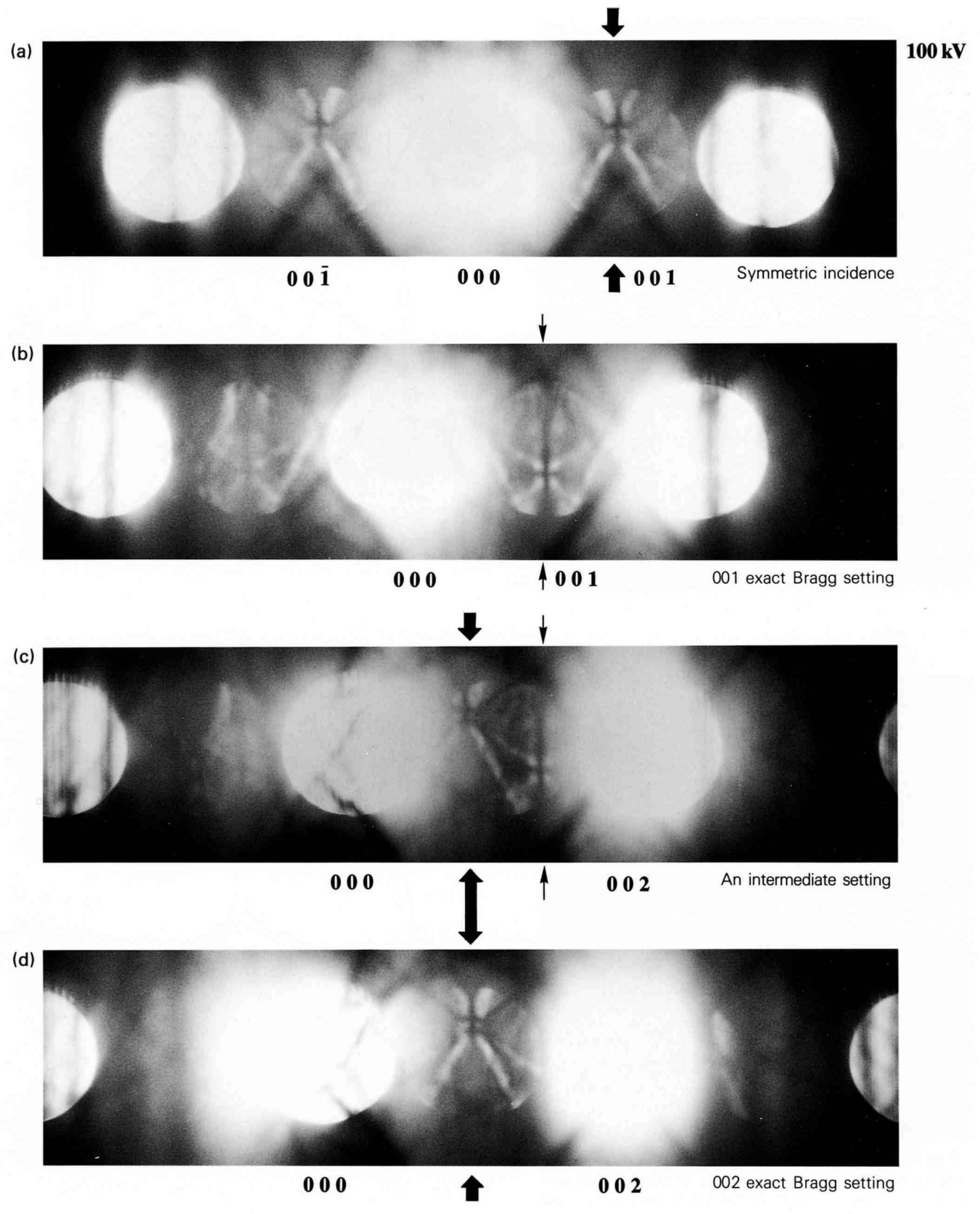
A series of photographs on the opposite page shows  $B_3$  type dynamical extinction lines appearing in the 001 reflection at different crystal settings: (a) symmetric incidence, (b) 001 exact Bragg setting, (c) intermediate setting between 001 and 002 Bragg settings and (d) 002 exact Bragg setting. True GM lines are seen at the positions indicated by fine arrows in Photos (b) and (c). The spurious  $B_3$  GM lines are seen at the centers of the 001 and  $00\bar{1}$  reflections at the symmetric incidence (a), at the center of the 001 reflection at the 002 exact Bragg setting (d), and at an off-center position in the 001 reflection (c), as indicated by thick arrows.

The reason for the appearance of the spurious  $B_3$  GM lines is as follows. A schematic diagram of Umweganregung paths via HOLZ reflections to the 001 and  $00\bar{1}$  reflections is given below for the symmetric incidence. These two reflections are kinematically forbidden due to the  $2_1$  screw axis in the [001] direction. The path  $aa'$  is found to be equivalent to the path  $bb'$  by successively operating twofold rotation about the [001] axis and inversion. The phases of the two beams coming through these paths are different by  $\pi$  from each other due to the existence of the  $2_1$  screw axis in the [001] direction. The path  $b'$  to the 001 reflection and the path  $b''$  to the  $00\bar{1}$  reflection from the same HOLZ reflection have a phase difference of  $2n\pi$ , because these two reflections differ by the vector of the 002 reflection. As a result, the two beams coming through the paths  $aa'$  and  $bb''$  still differ by  $(2n+1)\pi$  in phase. The amplitudes of Umweganregung via these paths are not the same, because the paths are not equivalent with respect to the twofold rotation. However, a dynamical extinction still takes place, since a partial cancellation of the amplitudes occurs between the two paths. The spurious  $B_3$  GM line, together with true  $B_2$  and  $B_3$  GM lines, indicates the existence of a  $2_1$  screw axis. It appears that spurious  $A_2$  and  $B_2$  GM lines do not occur, because a sufficient cancellation does not take place between Umweganregung-beams owing to strong scattering-angle dependences of atomic scattering factors for ZOLZ reflections.

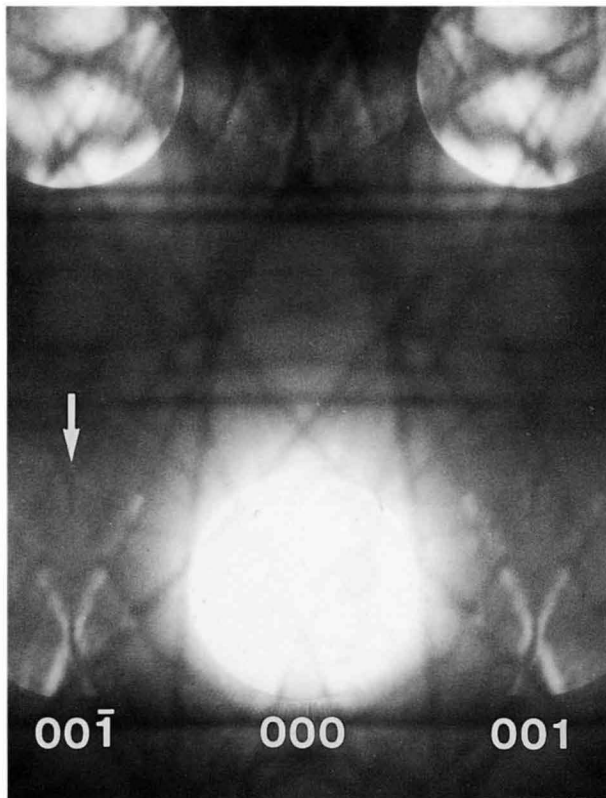
It is noted that the dynamical extinction observed in the 020 reflection due to a horizontal glide plane in spinel described on pages 36 to 39 is also a spurious GM line in the meaning given above. Furthermore, spurious ( $A_3$ ) GM lines due to vertical glide planes have been observed in 420 reflections from  $\text{MgAl}_2\text{O}_4$  at the [001] zone axis incidence.



**FeS<sub>2</sub>**

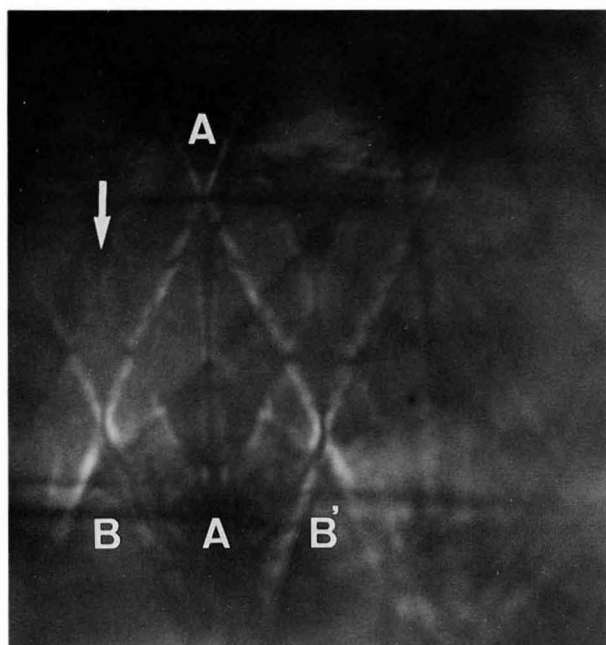
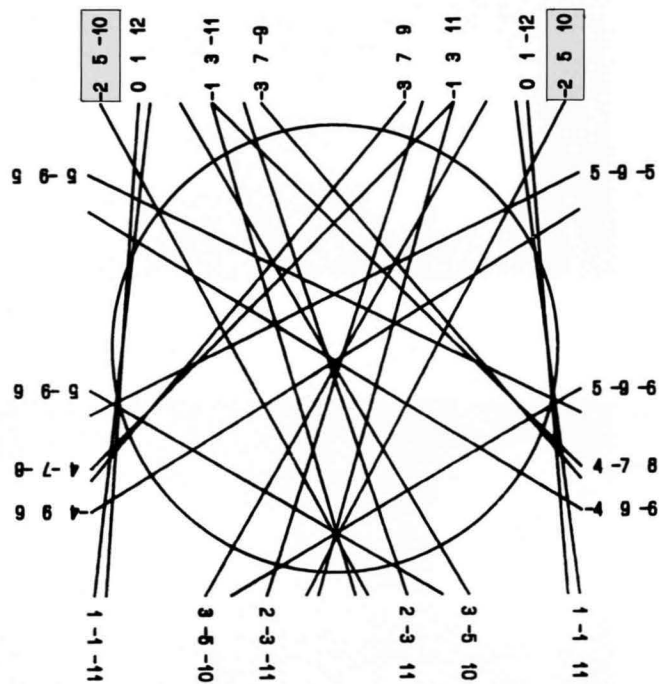


104 kV



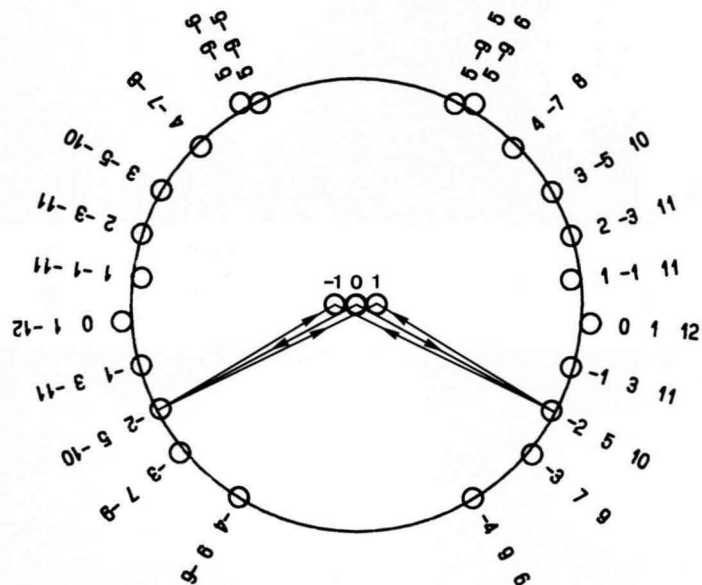
(a)

ZAP. Spurious  $B_3$  GM lines are seen at the centers of the 001 and  $00\bar{1}$  disks.



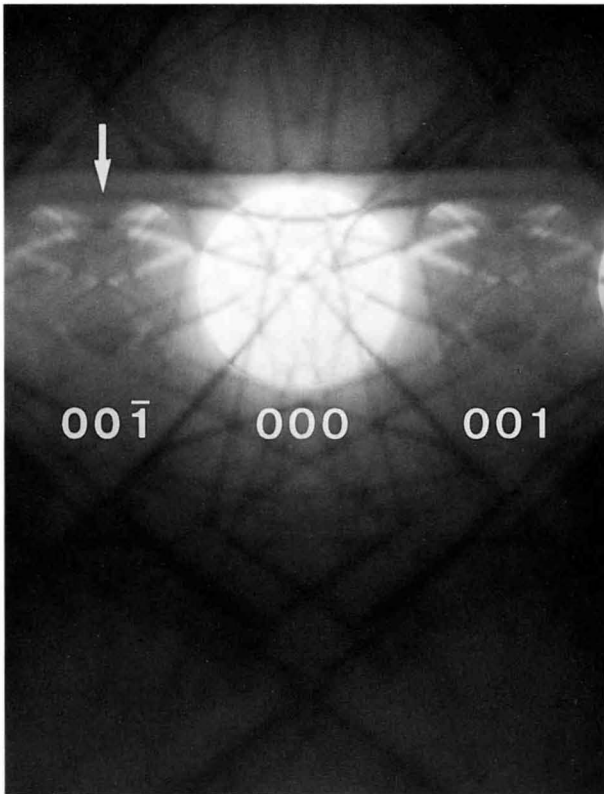
(b)

$00\bar{1}$  dark-field LACBED pattern. The angular position indicated by an arrow corresponds to that in (a). Spurious  $B_3$  GM lines are seen at B and B'. True  $B_3$  GM line is seen at the exact  $00\bar{1}$  Bragg position, A.

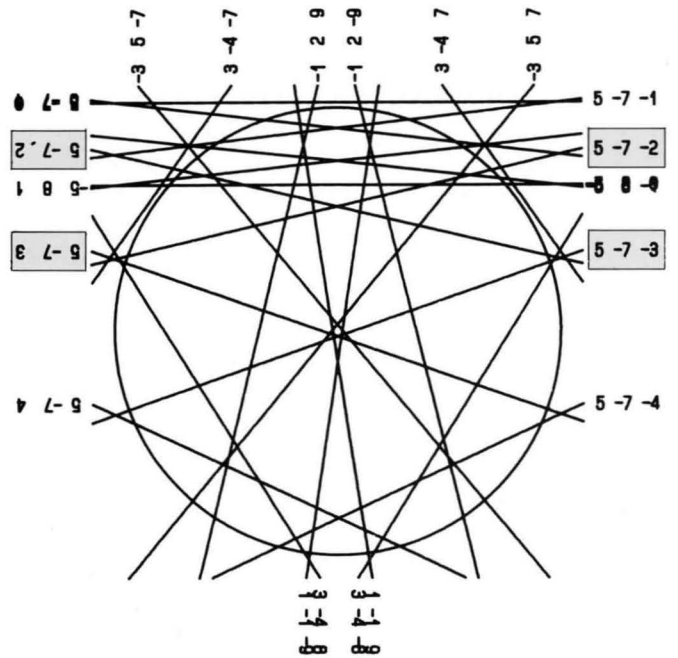


[320]

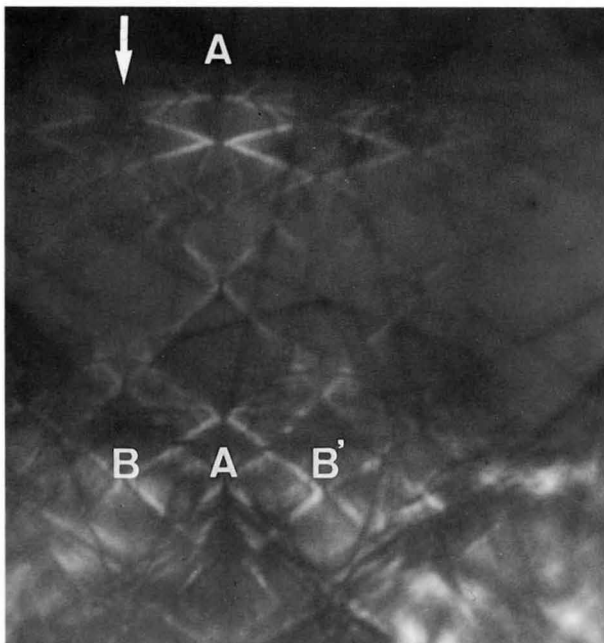
104 kV



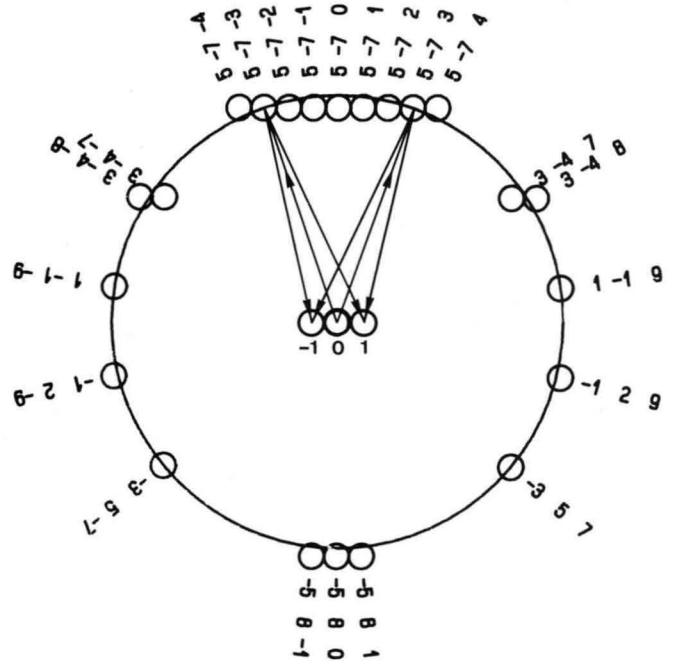
(a)



ZAP. Spurious  $B_3$  GM lines are seen at the centers of the  $00\bar{1}$  and  $001$  disks.



(b)



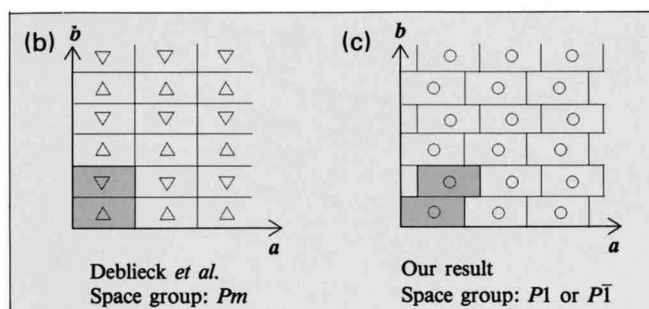
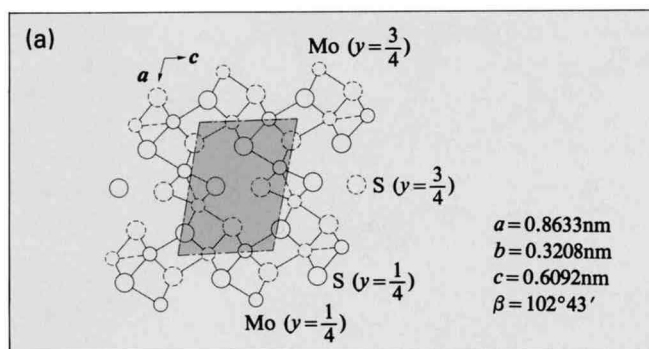
$00\bar{1}$  dark-field LACBED pattern. The angular position indicated by an arrow corresponds to that in (a). Spurious  $B_3$  GM lines are seen at  $B$  and  $B'$ . True  $B_3$  GM line is seen at the exact  $00\bar{1}$  Bragg position,  $A$ .

# Slight Breakdown of GM Lines

Substance  $\text{Mo}_2\text{S}_3$  belongs to a space group  $P2_1/m$  above approximately  $150^\circ\text{C}$ . The  $b$  projection of the structure of this phase is drawn in Fig. (a). After two phase transformations with decreasing temperature, it undergoes the last phase transformation at about  $-90^\circ\text{C}$ .

Photographs (a) and (b) were taken at  $155^\circ\text{C}$  and  $-185^\circ\text{C}$ , respectively. The  $hk/20$  reflections in (b) are superlattice reflections, indicating a cell doubling in the  $b$ -direction at the low temperature phase. The fundamental reflections in the CBED patterns (c) and (d) taken at  $-185^\circ\text{C}$  exhibit a mirror symmetry perpendicular to the  $b^*$  axis to a good approximation, and the  $0k0$  ( $k=\text{odd}$ ) fundamental reflections in the patterns (c), (e) and (g) show GM lines due to the  $2_1$  screw axis. These results indicate that the fundamental structure of the high temperature phase is almost preserved in the low temperature phase. The superlattice reflections  $hk/20$ , however, have no mirror symmetry and no GM line, these results being summarized in the table below. Therefore, the space group of the low temperature phase is  $P\bar{1}$  or  $P1$ . Figure (b) schematically shows a structural model given by Deblieck *et al.* Their model is that the fundamental structure is triclinic ( $\Delta$ ), while the superstructure is a monoclinic one composed of the twinning of two triclinic unit cells. On the other hand, our experimental result concluded that the fundamental structure is approximately monoclinic ( $\circ$ ) and the superstructure is triclinic (Fig. (c)).

If the superlattice reflections show a symmetry expected from a triclinic structure, the fundamental reflections are more or less affected by the superlattice reflections, and



Structure of low temperature phase of  $\text{Mo}_2\text{S}_3$

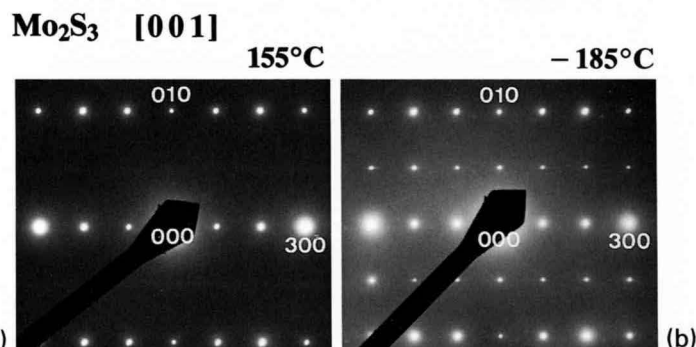
therefore should have the same symmetry as that of the superlattice reflections. Actually, a detailed inspection revealed that the fundamental  $0k0$  ( $k=\text{odd}$ ) reflection disks did not show correct GM lines. Photographs (e) and (g) were taken at the  $0\bar{3}0$  exact Bragg setting from a thin and a thick specimen area, respectively. Photographs (f) and (h) show enlarged  $0\bar{3}0$  dark-field patterns.  $A_2$  and  $B_2$  GM lines do not form an accurate black cross in the disks. The deviation from the cross is more easily seen for the thicker specimen (h). A symmetry  $2mm$  of the black cross is changed into a symmetry  $1_R$ . The symmetry  $1_R$  is expected in the case of the projection approximation or the 0th Laue zone interaction even if the specimen has no symmetry. It is also seen that the  $A_2$  GM lines in the  $0\bar{1}0$  reflection disks in Photos (c), (e) and (g) are not straight but of a little irregular shape owing to a slight breakdown of the  $2_1$  screw axis.

A slight breakdown of a symmetry of a crystal often occurs at a second order phase transition. In such a case crystal symmetries may be incorrectly determined. For the correct determination, it is helpful to know in advance how the symmetries of CBED patterns are changed by a slight breakdown of a crystal symmetry element. The present example provides an instructive demonstration on how a symmetry changes due to a slight breakdown of a  $2_1$  screw axis. That is, a pattern with crossed  $A_2$  and  $B_2$  GM lines having a symmetry  $2mm$  changes into a pattern of a symmetry  $1_R$  due to the breakdown of a  $2_1$  screw axis (or a glide plane). Such changes will be studied again in the section of computer simulations.

The specimens were supplied by Dr. N. Kobayashi and Prof. Y. Muto of the Research Institute for Iron, Steel and Other Metals, Tohoku University.

## Reference

[a] R. Deblieck, G.A. Wiegers, K.D. Bronsema, D. van Dyck, G. van Tendeloo, J. van Landuyt and S. Amelinckx: *phys. stat. sol.*, (a) 77 (1983) 249.

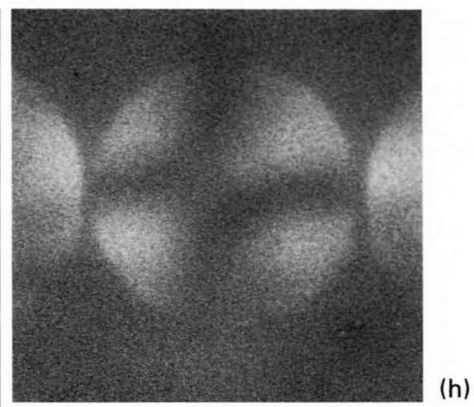
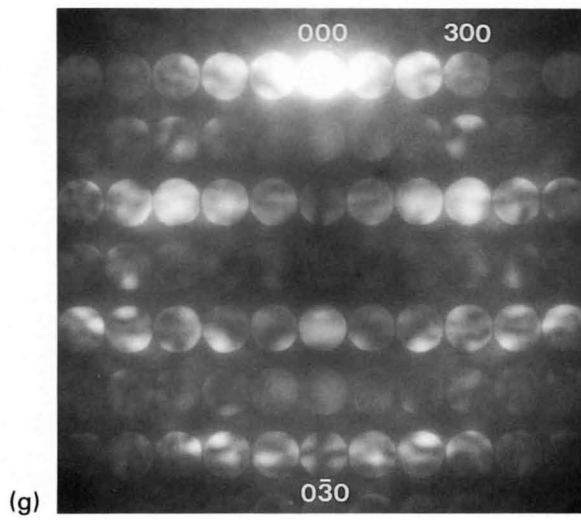
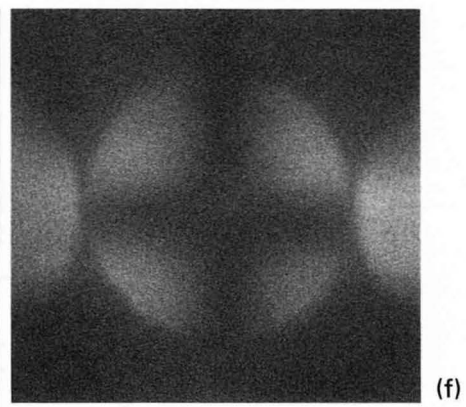
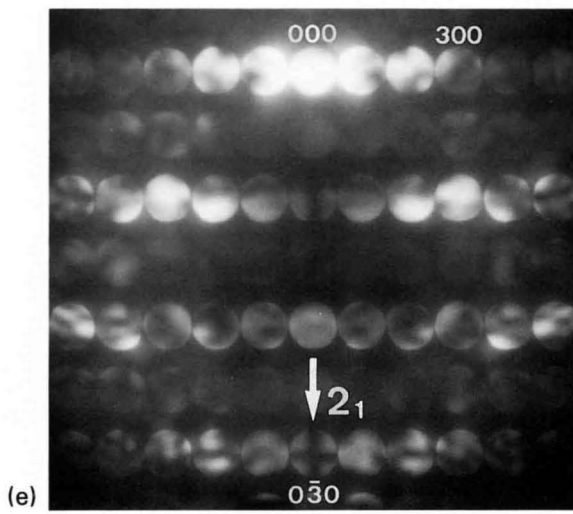
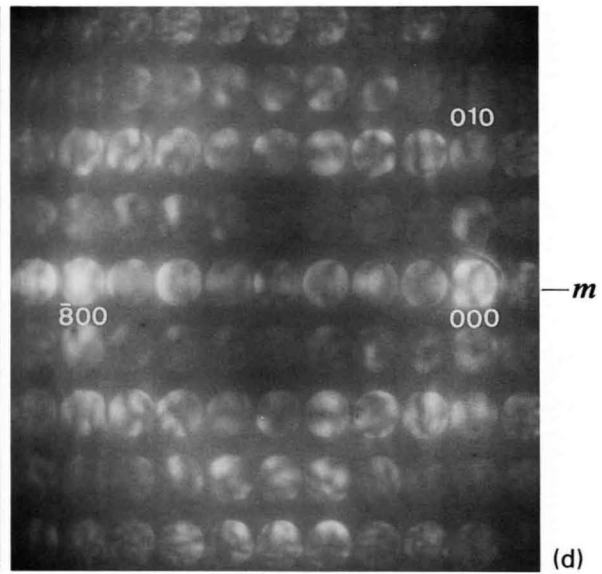
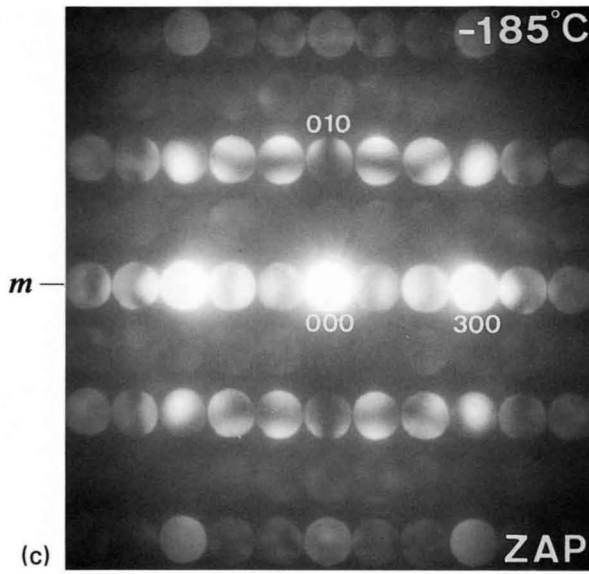


$T < -90^\circ\text{C}$

Fundamental reflections	$\sim 2_1/m$ (approximately)
Superlattice reflections	1

[001]

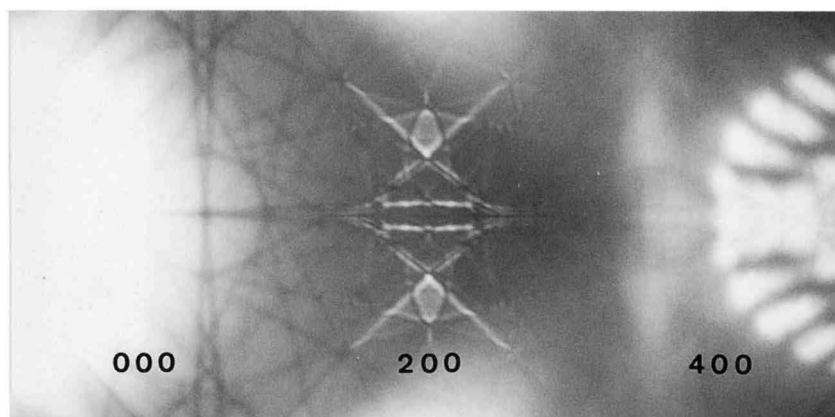
100 kV



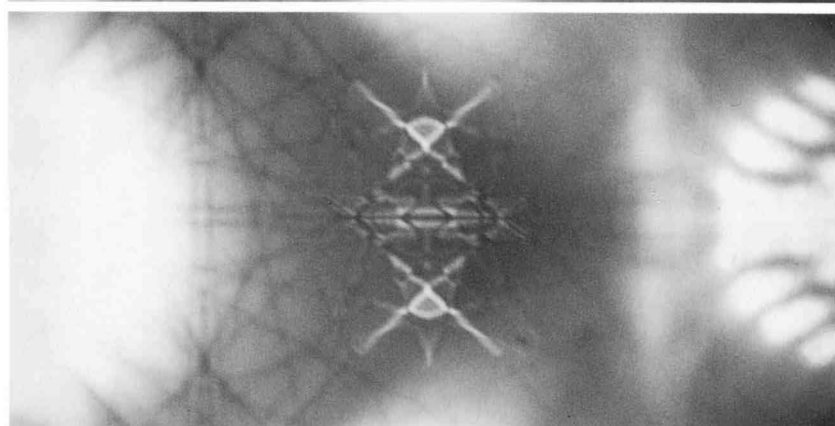
CBED patterns taken at  $-185^{\circ}\text{C}$ . (c) ZAP, (d)  $\bar{8}00$  excitation, (e) and (g)  $0\bar{3}0$  excitation. (f) and (h)  $0\bar{3}0$  disks of Photos (e) and (g).

# *A<sub>3</sub> and B<sub>3</sub> GM Lines from Cooled Specimens*

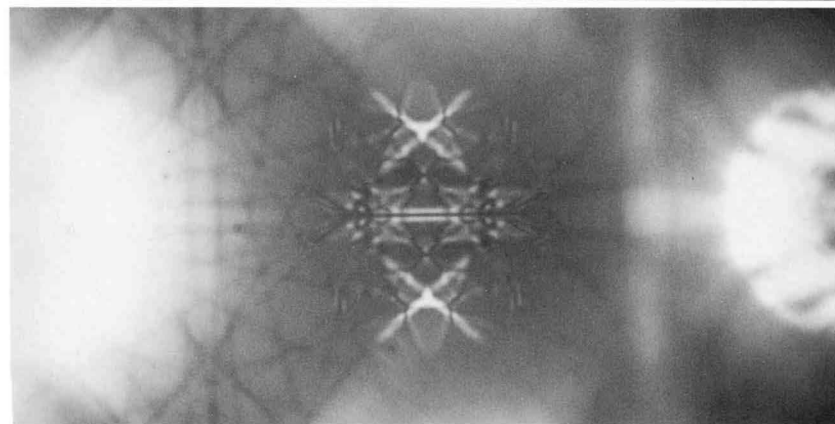
Si [001]



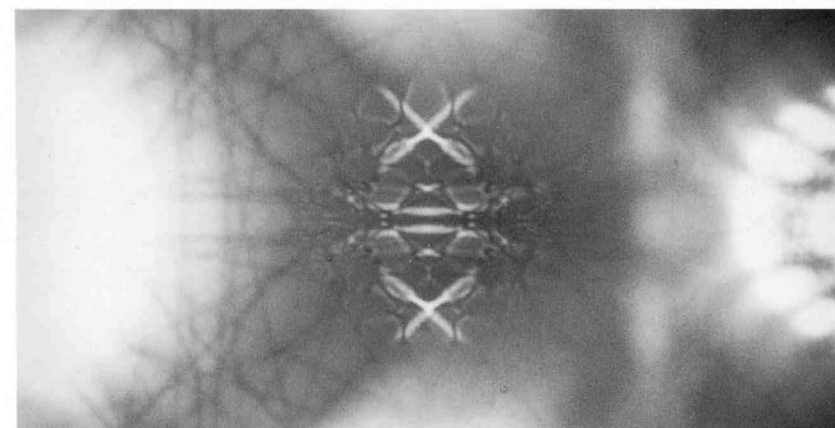
**61.5 kV** Cooling specimens down to the Liq.N<sub>2</sub> temperature, if possible, enables clear observation of A<sub>3</sub> and B<sub>3</sub> GM lines.



**62.0 kV**



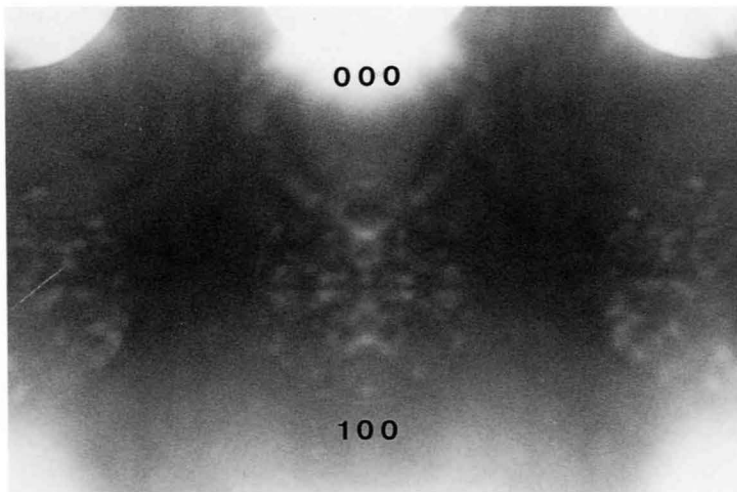
**62.5 kV**



**63.0 kV**

A<sub>3</sub> GM lines appearing in the 200 reflections taken at the Liq.N<sub>2</sub> temperature. Compare these with faint ones taken at room temperature, which have been given in book I.

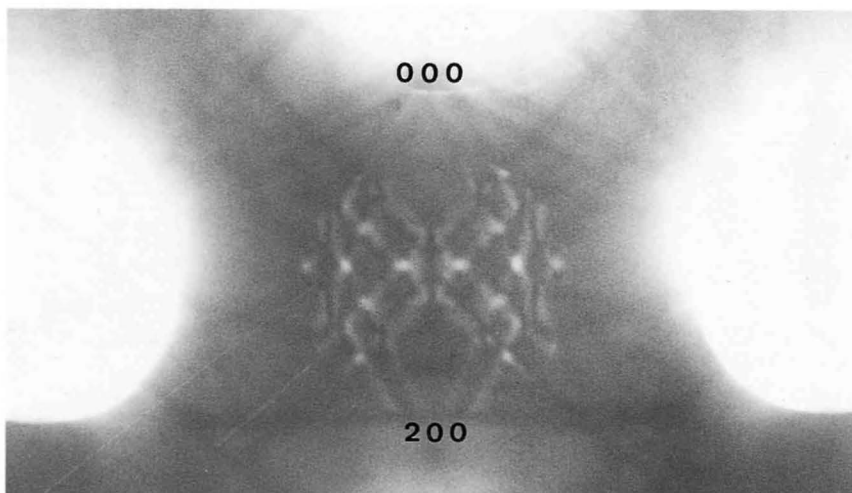
**FeS<sub>2</sub> [001]**



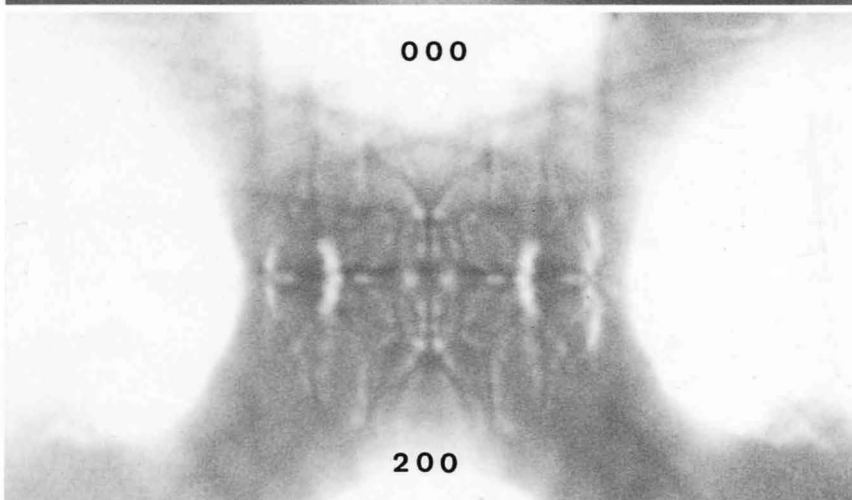
**55.0 kV**

A  $B_3$  GM line in the 100 reflection is seen at the Liq.N<sub>2</sub> temperature, whereas it is not observed at room temperature.

**MgAl<sub>2</sub>O<sub>4</sub> [001]**



**71.5 kV**



**55.0 kV**

$A_3$  GM lines in the 200 reflections are clearly seen, because many HOLZ lines appear over the whole disks at the Liq. N<sub>2</sub> temperature in contrast to a few weak lines at room temperature.

### Space groups indistinguishable by GM lines

The table of space groups indistinguishable by GM lines given in book I is not perfect. It should be replaced by the table given here. As a result, the number of distinguishable space groups should read 181 instead of 185 in the last paragraph on page 173 of book I. In the same paragraph, the 19 sets should read 21 sets. These corrections are due to Dr. J.A. Eades.

The 49 crystal space-groups in the present table can not be identified by GM lines. Whether an axis is a rotation axis or a screw axis can be made clear by observing how the intensities of reflections which may be kinematically forbidden change when the crystal orientation is varied. If an axis is a screw axis, kinematically forbidden reflections show a sudden decrease in intensity with a rotation that causes the loss of Umweganregung paths. If the axis is a rotation axis, the intensities of the reflections are not changed conspicuously by such a rotation. By such a test, each space group in the 21 sets can be identified except the pairs in parentheses and pairs 16 and 17. The pairs in parentheses form left- and right-handed space groups. The handedness of space groups can be identified in such a way that the senses of two crystal axes are determined with the aid of crystal structure factor calculations and the sense of the third axis is determined with the aid of dynamical calculations ([a], [b] and [c]). It should be noted that two special pairs 16 and 17 ( $I222$  and  $I2_12_12_1$ ,  $I23$  and  $I2_13$ ) can not be distinguished from kinematical extinction rules, but distinguished when atomic positions are determined.

In crystal data on 5572 different inorganic materials collected by Nowacki[d], the numbers of materials be-

longing to a space group among the sets 1, 4, 8, 10, 12, 14, 17, 18 and 21 are less than two, those belonging to a space group among the sets 6, 9, 13, 15, 16, 19 and 20 are less than ten, and only those belonging to the sets 2, 3, 5, 7 and 11 are more than fifteen. It is emphasized that the probability to find most indistinguishable space groups is very low.

- |                                       |                             |
|---------------------------------------|-----------------------------|
| 1. $P3$ , ( $P3_1$ , $P3_2$ )         | 12. $P422$ , $P4_222$       |
| 2. $P312$ , ( $P3_112$ , $P3_212$ )   | 13. $P42_12$ , $P4_22_12$   |
| 3. $P321$ , ( $P3_121$ , $P3_221$ )   | 14. $I4$ , $I4_1$           |
| 4. $P6$ , ( $P6_2$ , $P6_4$ )         | 15. $I422$ , $I4_122$       |
| 5. $P622$ , ( $P6_222$ , $P6_422$ )   | 16. $I23$ , $I2_13$         |
| 6. $P6_3$ , ( $P6_1$ , $P6_5$ )       | 17. $I222$ , $I2_12_12_1$   |
| 7. $P6_322$ , ( $P6_122$ , $P6_522$ ) | 18. $P432$ , $P4_232$       |
| 8. $P4$ , $P4_2$                      | 19. ( $P4_132$ , $P4_332$ ) |
| 9. ( $P4_1$ , $P4_3$ )                | 20. $I432$ , $I4_132$       |
| 10. $P4/m$ , $P4_2/m$                 | 21. $F432$ , $F4_132$       |
| 11. $P4/n$ , $P4_2/n$                 |                             |

### References

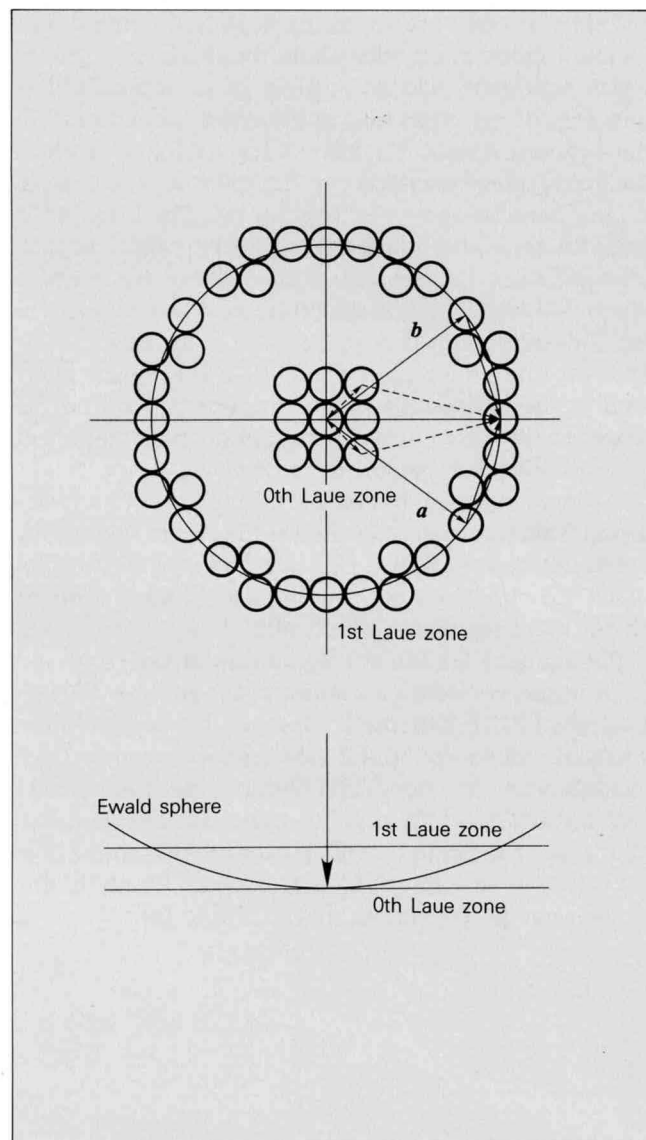
- [a] P. Goodman and T.W. Secomb: *Acta Cryst.*, **A33** (1977) 126.  
 [b] P. Goodman and A.W.S. Johnson: *Acta Cryst.*, **A33** (1977) 997.  
 [c] M. Tanaka, H. Takayoshi, M. Ishida and Y. Endoh: *J. Phys. Soc. Jpn.*, **54** (1985) 2970.  
 [d] W. Nowacki: Crystal Data, ACA Monograph No. 6, American Crystallographic Association (1967).

## GM Lines in HOLZ Reflections

Space-group determination has been carried out by using GM lines appearing in ZOLZ reflections [3], [8]. The GM lines are caused by the crystal symmetry elements which act as horizontal  $2_1$  screw axes, vertical glide planes with horizontal translation vectors and horizontal glide planes [7]. The vertical glide planes give rise to GM lines also in HOLZ reflections. Vertical glide planes whose translation vectors are perpendicular to the specimen surface (vertical translation) do not cause GM lines in ZOLZ reflections but cause them in HOLZ reflections (see page 59). It should be noted that vertical glide planes with glide translations not-parallel to the surface are not symmetry elements of diperiodic plane figures.

Vertical screw axes also form GM lines in HOLZ reflections whose vectors are parallel to the screw axes. However, these reflections cannot be observed by usual transmission CBED. Therefore, only glide planes can be identified from GM lines in HOLZ reflections.

HOLZ GM lines



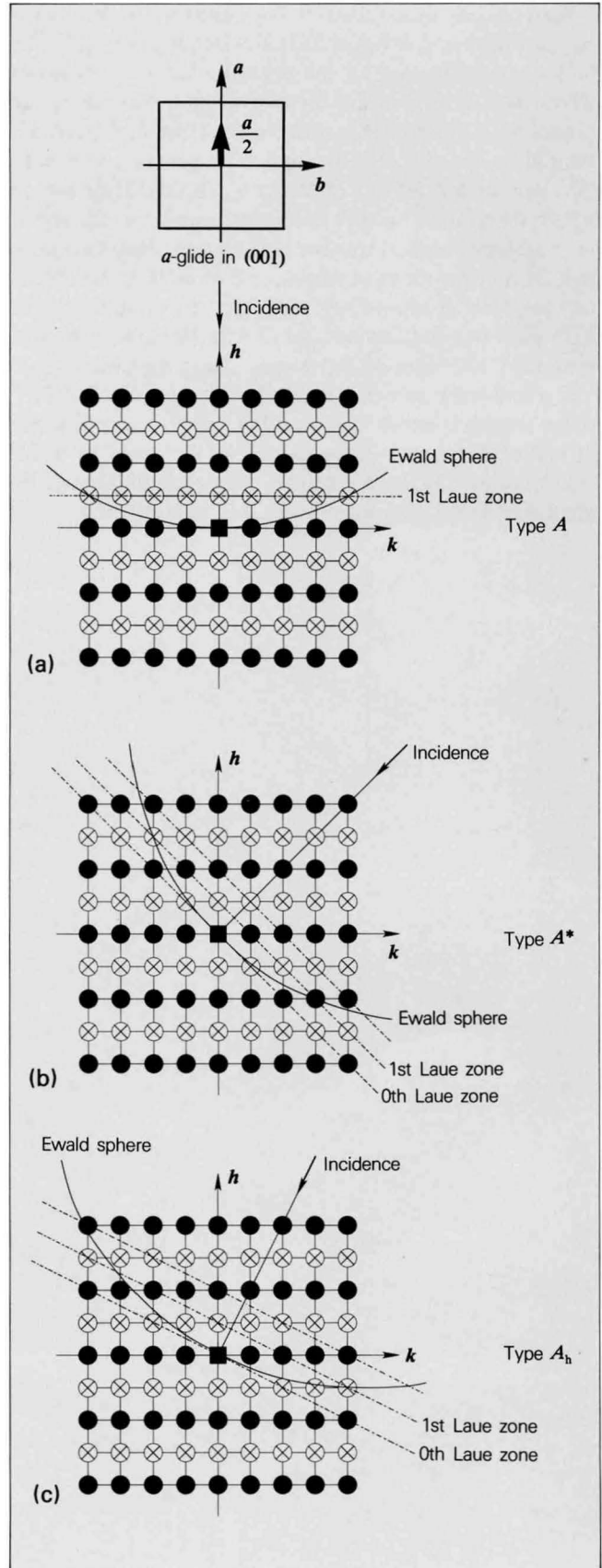
The symmetric paths *a* and *b* with respect to a vertical glide plane produce a GM line in a HOLZ reflection.

Tables of GM lines appearing in HOLZ reflections at various incident beam orientations for all the space groups which have glide planes, are given in an appendix. The meanings of the letters used in the tables are explained in the diagrams at right. The letter *A* is given for cases where the Ewald sphere intersects two circled-cross-reflections in a Laue zone, as shown in diagram (a). The letter *A\** is given for cases where the Ewald sphere intersects a circled-cross-reflection on one side of the incident beam and a black-circle-reflection on the other, as shown in diagram (b). This case occurs only in the space group  $P2_1/a\bar{3}$ . The letter  $A_h$  is given for cases where the Ewald sphere intersects a circled-cross-reflection on one side but does not intersect on the other, owing to the asymmetric arrangement of reflections with respect to the incident beam.

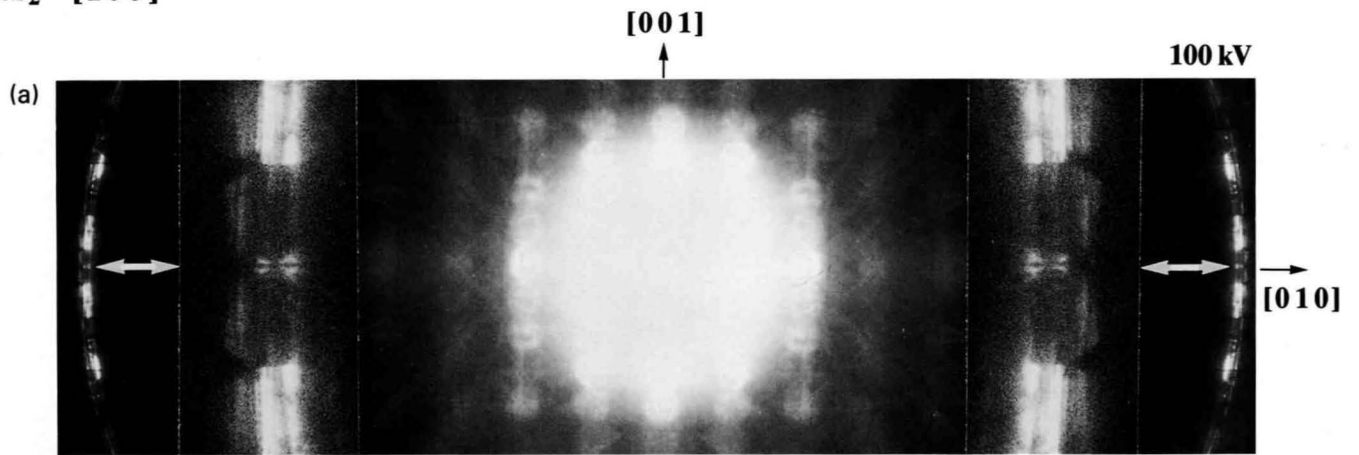
It should be noted that HOLZ GM lines are clearly observed from specimen areas thinner than those suitable for the observation of ZOLZ GM lines, because the profiles of HOLZ reflections are concentrated in small areas of CBED disks for thicker specimens.

Photographs (a) and (b) were taken at the [100] and [110] incidences from  $\text{FeS}_2$  whose space group is  $P2_1/a\bar{3}$ . Enlarged HOLZ patterns are inserted for easy viewing. The table shows the HOLZ GM lines expected in three incident beam directions. GM lines of type *A* are seen in two  $h_0k0$  HOLZ reflections of Photo (a) due to the *a*-glide plane parallel to the (001) plane. A GM line of type *A\** is seen in an  $h_0k0$  HOLZ reflection of Photo (b) due to the same glide plane as that of Photo (a).

### HOLZ GM lines

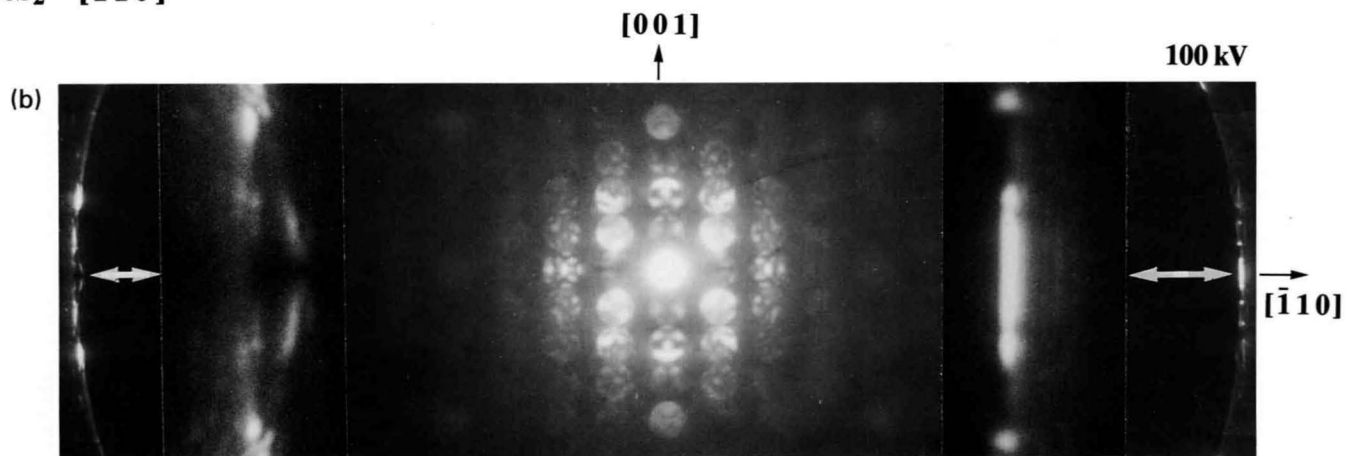


**FeS<sub>2</sub> [100]**



Type A GM line due to an  $\alpha$ -glide in the (001) plane.

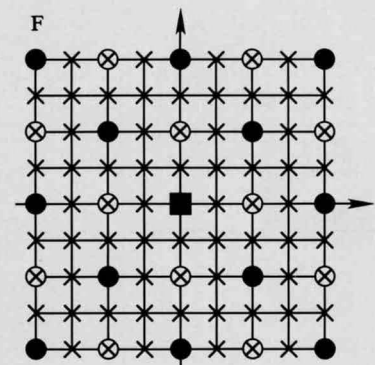
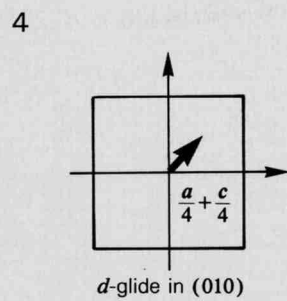
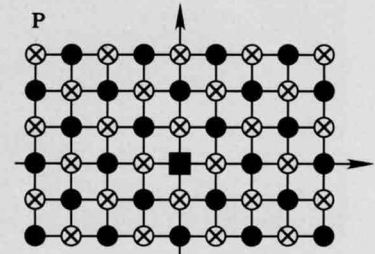
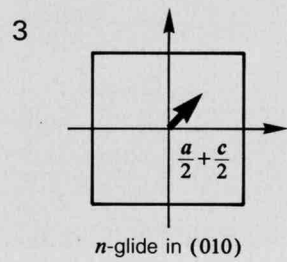
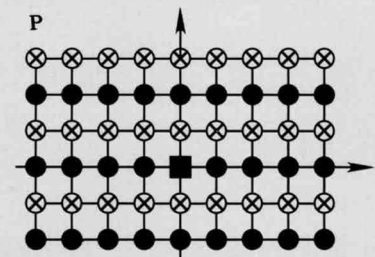
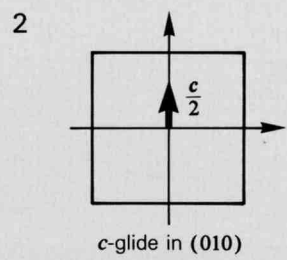
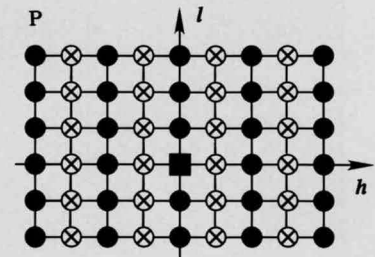
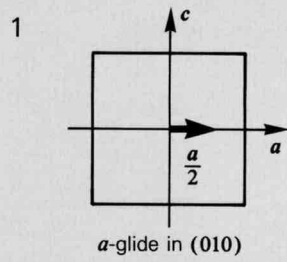
**FeS<sub>2</sub> [110]**

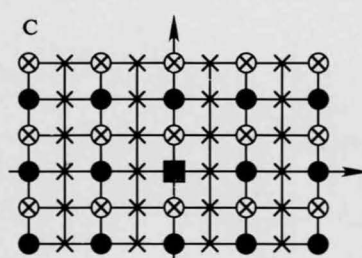
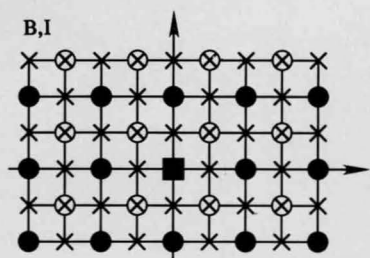
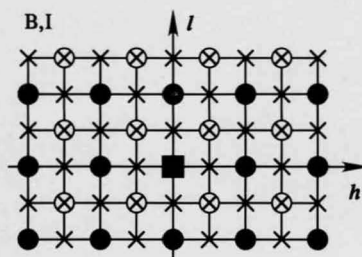
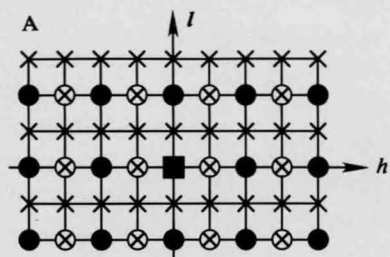


Type A\* GM line due to an  $\alpha$ -glide in the (001) plane.

**Point group  $m\bar{3}$**

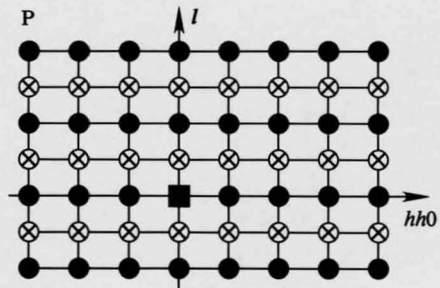
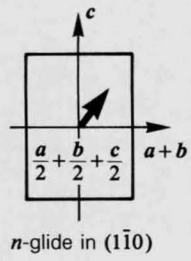
Incident beam direction	[100]		[110]		[ $uv$ 0]	
Space group						
205 $Pa\bar{3}$ $P2_1/a\bar{3}$	$h0l_0$ $c_2$ $h_0k0$ $a_3$	$A$	$h_0k0$ $a_3$	$A^*$	$h_0k0$ $a$	$A_h$



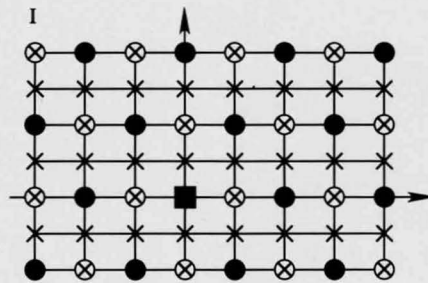
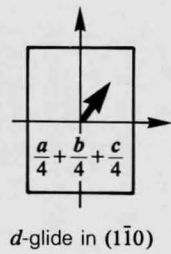


- P: Primitive lattice
- A, B and C: A, B and C centered lattices, respectively
- I: Body centered lattice
- F: Face centered lattice
- : Allowed reflections
- ×: Kinematically and dynamically forbidden reflections due to lattice types
- ⊗: Kinematically forbidden but dynamically allowed reflections due to glide planes

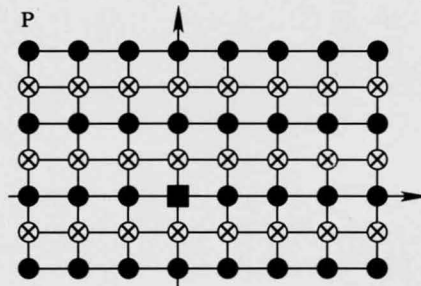
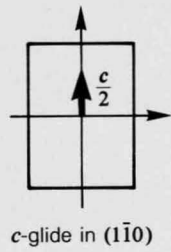
5



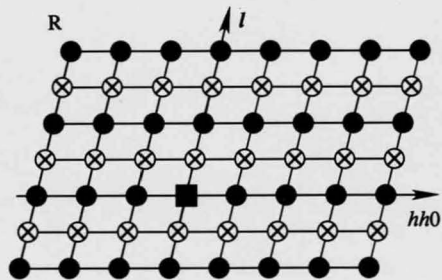
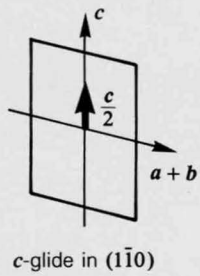
6

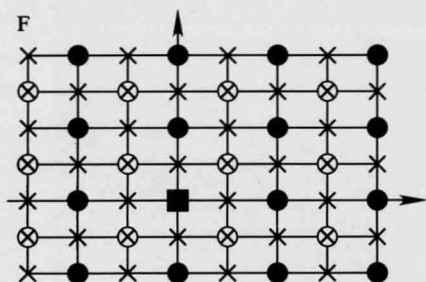


7a



7b

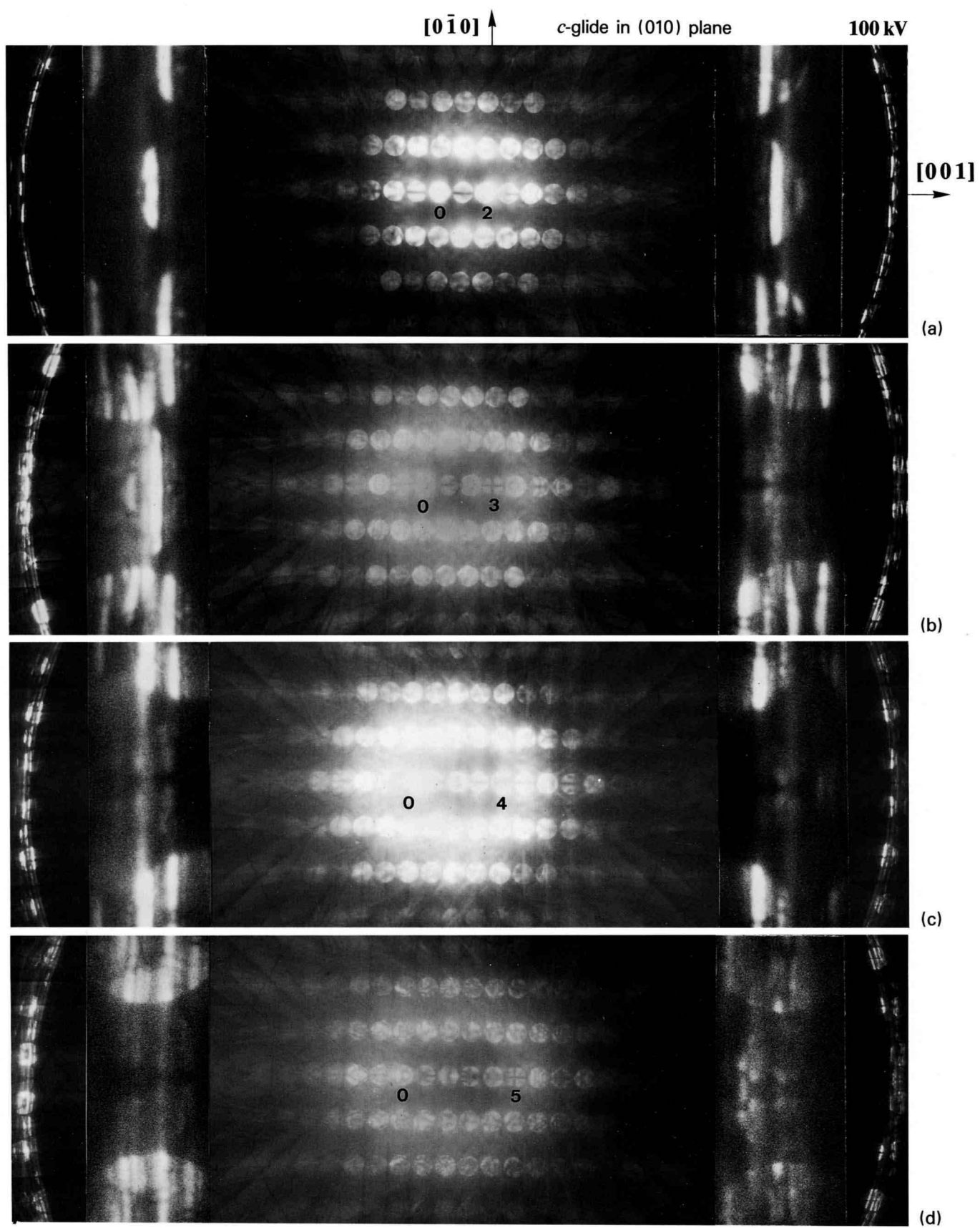




- P: Primitive lattice
- A, B and C: A, B and C centered lattices, respectively
- I: Body centered lattice
- F: Face centered lattice
- R: Rhombohedral lattice
- : Allowed reflections
- X: Kinematically and dynamically forbidden reflections due to lattice types
- ⊗: Kinematically forbidden but dynamically allowed reflections due to glide planes

Figures on pages 54 to 57 show various vertical glide planes and schematically depict the arrangements of kinematically allowed (black circles), kinematically and dynamically forbidden (crosses), and kinematically forbidden but dynamically allowed (circled crosses) reflections for possible combinations of lattice types and glide planes. When the Ewald sphere intersects HOLZ reflections designated with circled crosses, GM lines appear in the reflections.

FeS<sub>2</sub> [100] — Changes of excitation condition



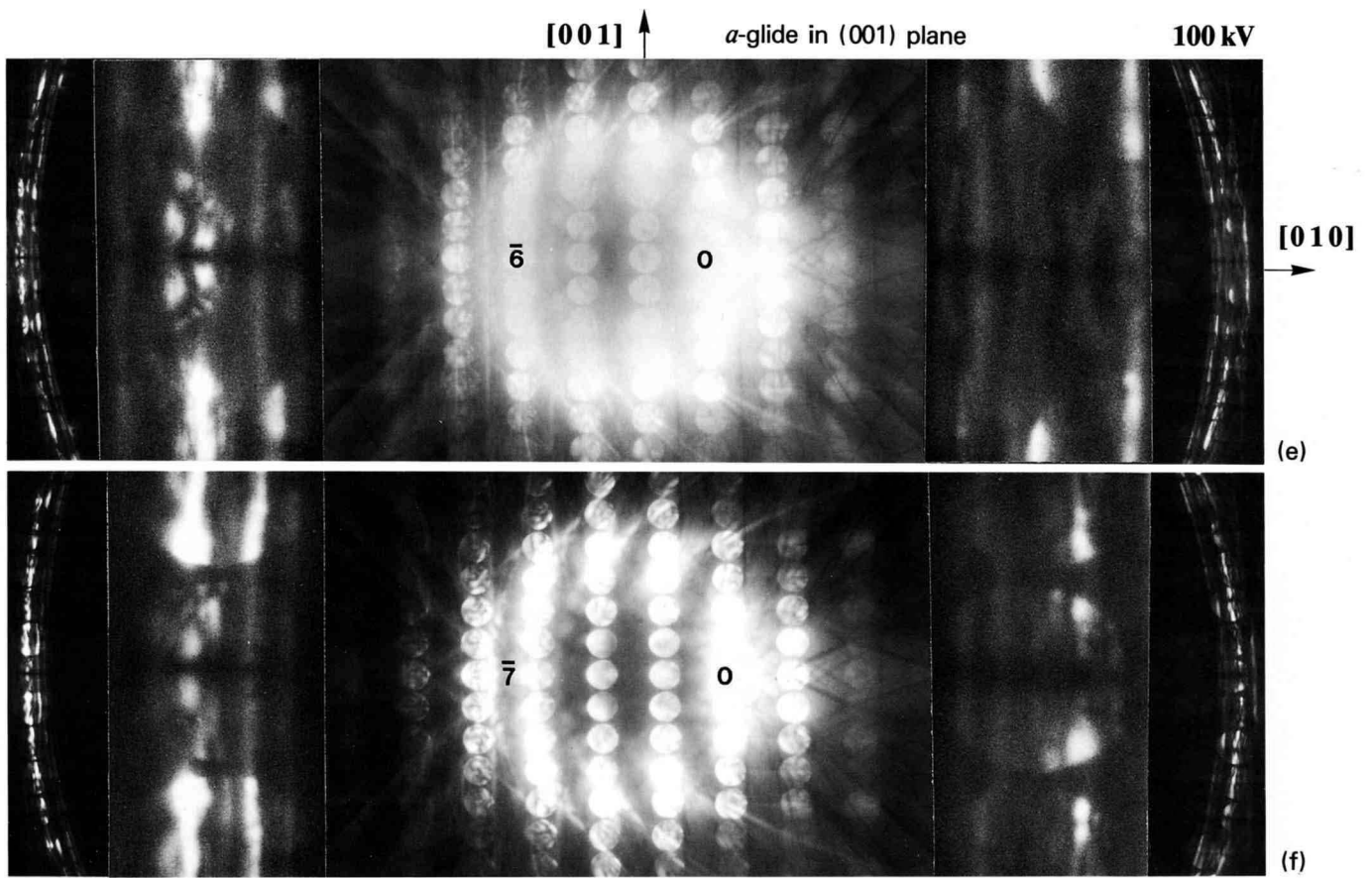


Table (a)

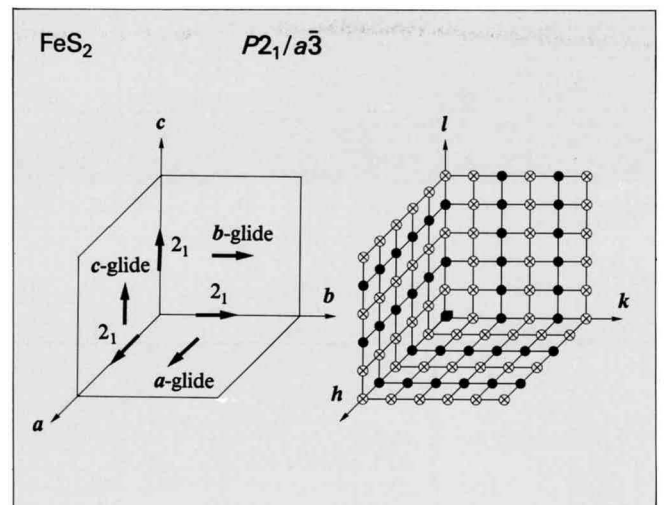
	Exactly excited ZOLZ reflection	GM line in $10l$ HOLZ reflection	
		left	right
(a)	002	no	no
(b)	003	no	yes
(c)	004	yes	yes
(d)	005	yes	no

Table (b)

	Exactly excited ZOLZ reflection	GM line in $1k0$ HOLZ reflection	
		left	right
(e)	$0\bar{6}0$	yes	yes
(f)	$0\bar{7}0$	yes	yes

Incident beam direction	[100]		
Space group			
205 $Pa\bar{3}$ $P2_1/a\bar{3}$	$h0l_0$ $c_2$ $h_0k0$ $a_3$	A	

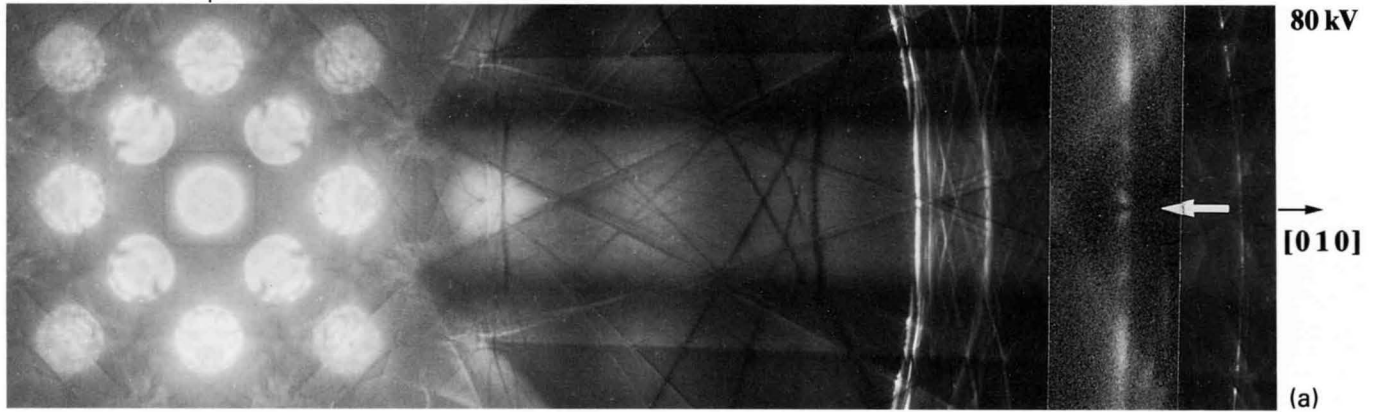
A series of Photos (a) to (d) and two Photos (e) and (f) show the variation of the appearance of GM lines with changes of the excitation condition. The results are summarized in Tables (a) and (b) for the former and the latter photos. The words "left" and "right" indicate left and right HOLZ reflections. The word "yes" expresses the presence of a GM line, and "no" the absence of a GM line. These results can be understood with the help of the figures below.



MgAl<sub>2</sub>O<sub>4</sub> [100]

ZAP ↑ [001]

*d*-glide in (001) plane

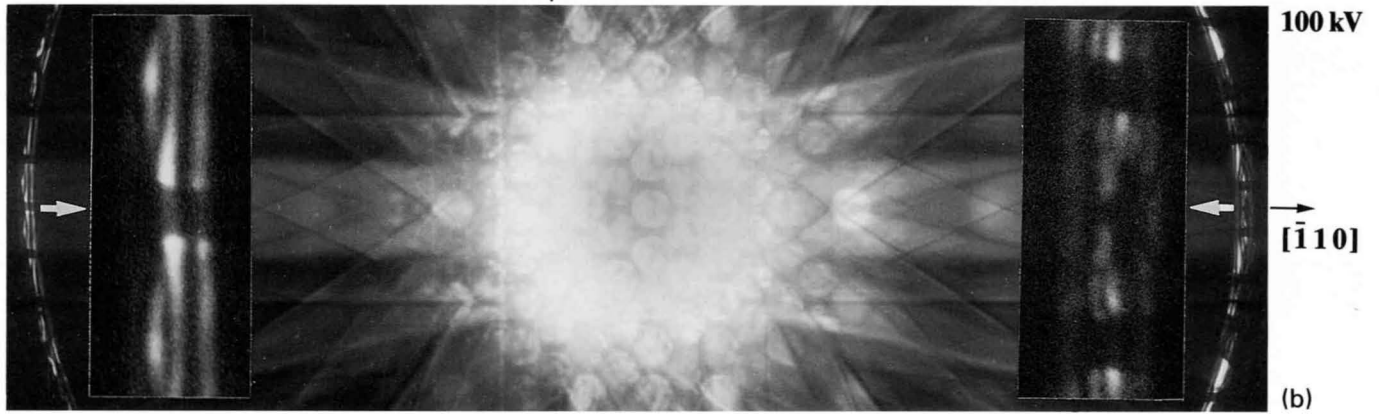


MgAl<sub>2</sub>O<sub>4</sub> [110]

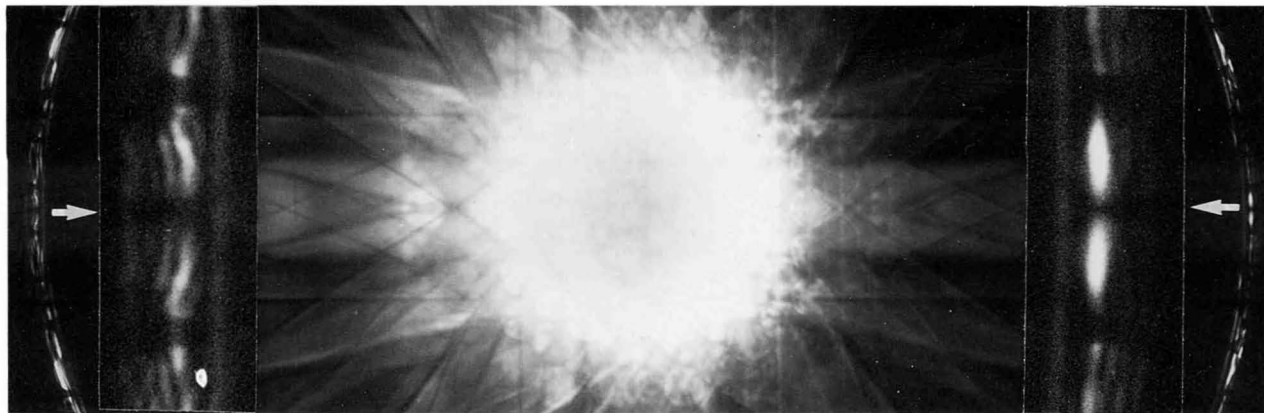
$\bar{5}50$  excitation

↑ [001]

*d*-glide in (001) plane

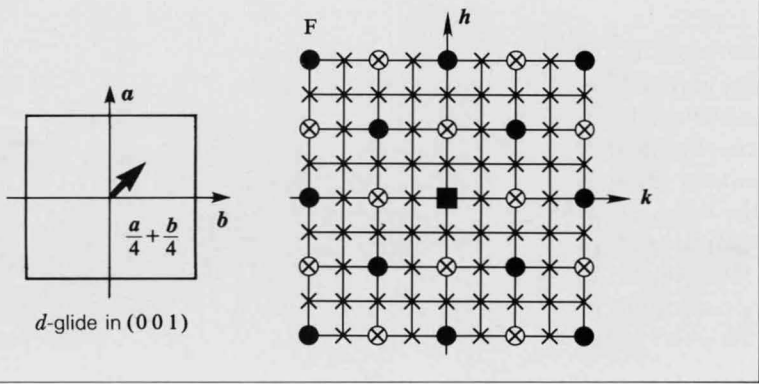


$\bar{6}60$  excitation



Point group *m*3*m*

Incident beam direction	[100]	[110]	[ <i>uv</i> 0]	[ <i>uvw</i> ]
Space group				
227 <i>Fd</i> 3 <i>m</i> <i>F</i> 4 <sub>1</sub> / <i>d</i> 3 <sub>2</sub> / <i>m</i>	$h_e 0 l_e$ $h_e + l_e = 4n + 2$ $d_2$ $h_e k_e 0$ $h_e + k_e = 4n + 2$ $d_3$	<i>A</i> $h_e k_e 0$ $h_e + k_e = 4n + 2$ $d_3$	<i>A</i> $h_e k_e 0$ $h_e + k_e = 4n + 2$ $d$	$A_h$



# Space-Group Determinations

## La<sub>2</sub>CuO<sub>4-δ</sub>

La<sub>2-x</sub>M<sub>x</sub>CuO<sub>4-δ</sub> (M = Ba, Sr and Ca) is a 40 K class superconductor. Many space groups were proposed for this system: *Fmmm*, *Fmm2*, *F222* and *Cmmm* (or *C222*) for La<sub>2-x</sub>Sr<sub>x</sub>CuO<sub>4-δ</sub>, *Cmca*, *Pccn* and *Pccm* for La<sub>2-x</sub>Ba<sub>x</sub>CuO<sub>4-δ</sub> and *Cmca*, *Pccn* and *Cmmm* for La<sub>2</sub>CuO<sub>4-δ</sub>. These controversial results may be attributed to specimen preparation, doping effects and experimental accuracy.

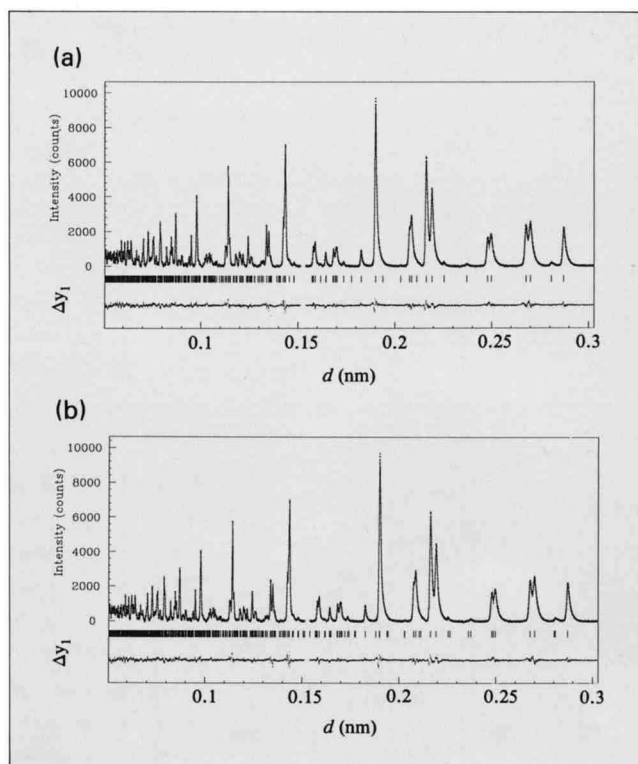
Figures (a) and (b) show intensity profile fits obtained by the Rietveld method for the neutron powder diffraction data from as-grown La<sub>2</sub>CuO<sub>4-δ</sub>. The fits to the experimental data are excellent but show no difference for the two space groups, *Cmca* (a) and *Pccn* (b). Therefore, the space groups could not be distinguished by the powder diffraction data.

Photograph (a) shows typical twin domains of this substance. Photographs (b) to (e) show electron diffraction patterns taken at four different electron incidences. The schematic diagrams corresponding to the patterns are given in Figs. (c) to (e). The large and small black circles indicate the observed reflections. From the extinction rules for the reflections, a possible lattice type is the B-centered type. The forbidden reflections due to this lattice type are denoted by crosses. The other reflections indicated by circled crosses must vanish due to screw axes and/or glide planes. The 010 and 0 $\bar{1}$ 0 reflections are not seen in Photo (b) but seen in Photo (c). This fact means that the reflections observed in Photo (c) occurred owing to Umweganregung. From these results, we obtained a space group *Bmab* (= *Cmca*). However, we have determined the space group unambiguously by revealing the symmetry elements of the crystal using CBED.

Photograph (f) shows a CBED pattern taken at the [001] incidence, Photo (g) being the central part of Photo (f). The whole pattern has a symmetry *2mm*. This indicates that the crystal has two mirror symmetries perpendicular to each other and that the point group is *mmm* or *mm2*. To investigate whether the third mirror plane perpendicular to these two mirror planes exists or not, a CBED pattern was taken at the [100] incidence (Photos (h) and (i)). Two mirror planes are seen, one of which being the third one. As a result, the point group was determined to be *mmm*.

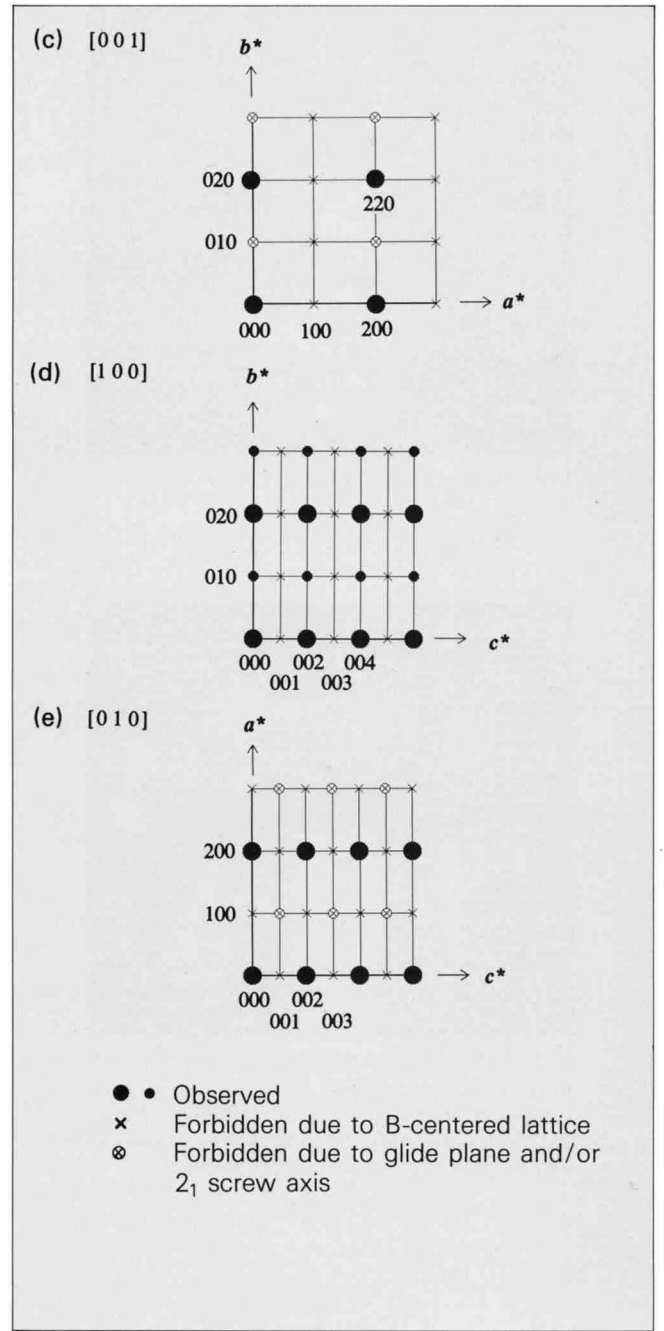
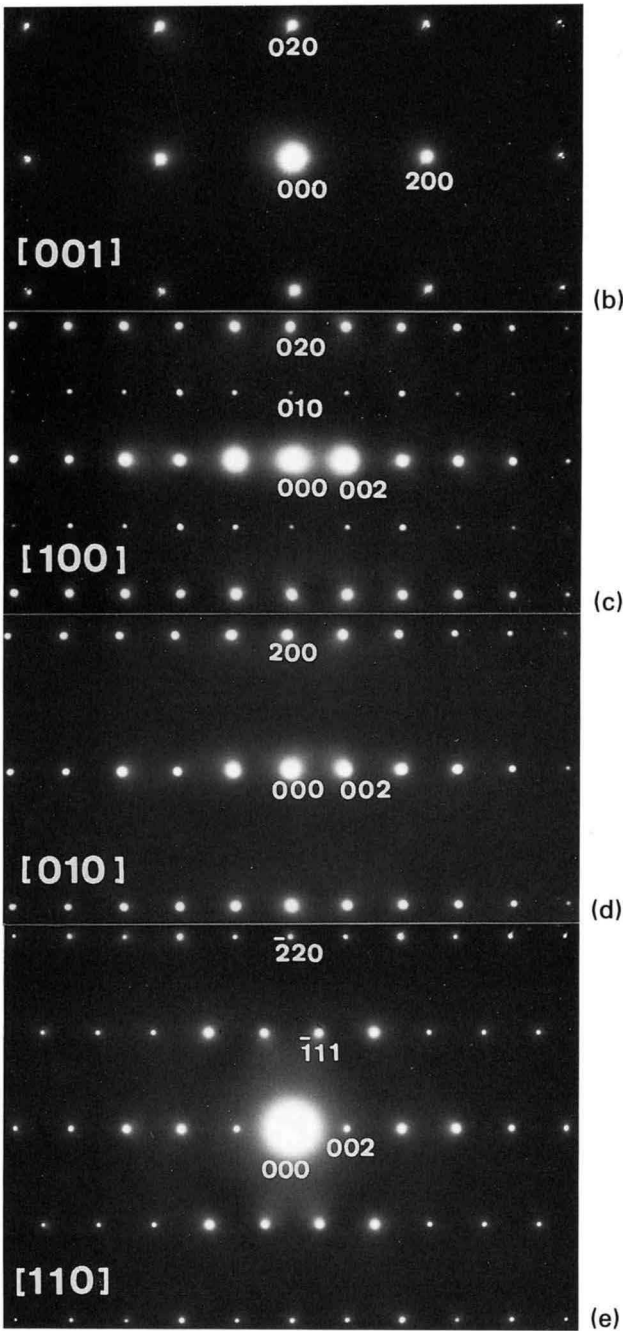
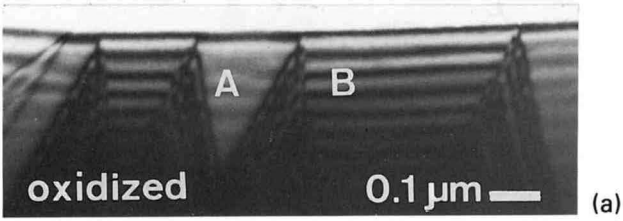
Photograph (j) was taken by tilting the incident beam in the *b\** direction from the [100] zone axis to clearly observe the GM lines. *A*<sub>2</sub> GM lines are seen in the 010 and 0 $\bar{5}$ 0 reflections. Reference to Table (a) for ZOLZ GM lines clarified that the possible space groups are *Bmab* and *Bmmb*. In Photo (h), type *A* GM lines are seen in the 10 $\bar{l}$  and 10 $\bar{l}$  HOLZ reflections. Reference to Table (b) for HOLZ GM lines allowed determining the space group to be *Bmab*, which is equivalent to *Cmca* in the standard notation. For confirmation, GM lines were observed at two other incidences. That is, a *B*<sub>2</sub> GM line was observed

in the 010 reflection at a [*u0w*] incidence (Photo (k)) and *A*<sub>2</sub> GM lines in the 2 $\bar{1}$ 0 and 2 $\bar{1}$ 0 reflections at the [120] incidence (Photo (l)). These observations show a good agreement with the predictions in Table (a).

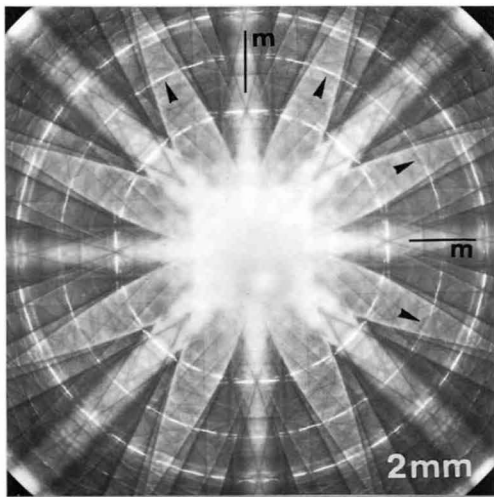


## References

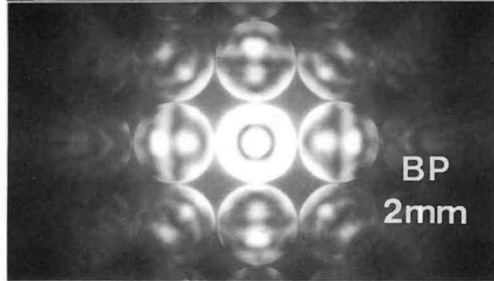
- [a] M. Tanaka, K. Tsuda, K. Yamada, Y. Endoh, Y. Hidaka, M. Oda, M. Suzuki and T. Murakami: *Jpn. J. Appl. Phys.*, **26** (1987) L1502.
- [b] K. Yamada, E. Kudo, Y. Endoh, K. Tsuda, M. Tanaka, K. Kokusho, H. Asano, F. Izumi, M. Oda, Y. Hidaka, M. Suzuki and T. Murakami: *Jpn. J. Appl. Phys.*, in the press.



[001]



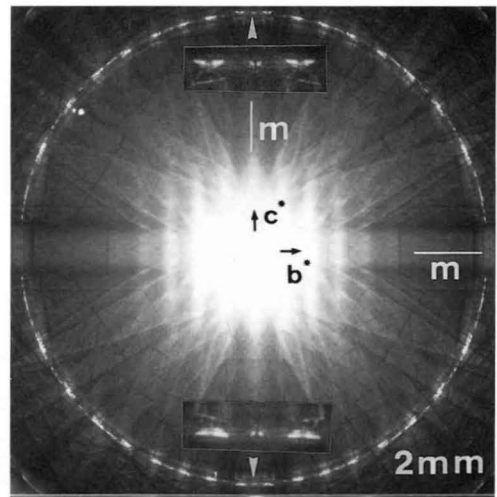
(f)



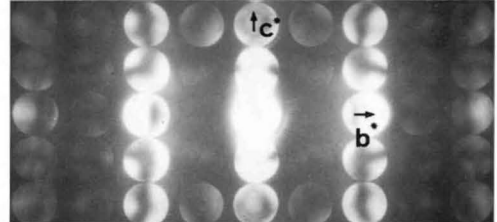
(g)

Point group:  $mmm$  or  $mm2$

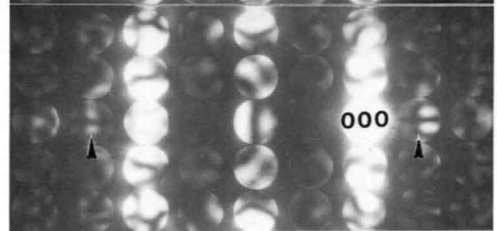
[100]



(h)

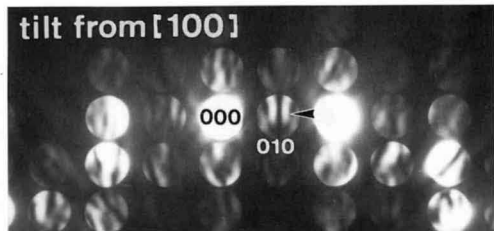


(i)

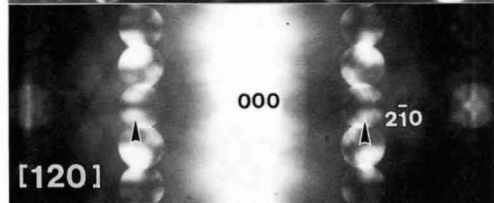


(j)

$A_2$  GM lines in the  $010$  and  $0\bar{5}0$  reflections in Photo (j) indicate the presence of a  $2_1$  screw axis parallel to the  $[010]$  axis and/or that of a  $b$ -glide plane in the  $(001)$  plane. A type  $A$  GM line in the  $10l$  and  $10\bar{l}$  reflections in Photo (h) indicate the presence of an  $a$ - or a  $c$ -glide plane in the  $(010)$  plane.



(k)



(l)

A  $B_2$  GM line in the  $010$  reflection in Photo (k) indicates the presence of a  $2_1$  screw axis parallel to the  $[010]$  axis.  $A_2$  GM lines in the  $2\bar{1}0$  and  $210$  reflections indicate the presence of a  $b$ -glide plane in the  $(001)$  plane.

Table (a) ZOLZ GM line table

Incident beam direction Space group	[100]		[010]		[001]		[uv0]		[0vw]		[u0w]	
	63 $B2/m2_1/m2/b$	$0k_00$ $b, 2_1$	$A_2 B_2$ $A_3 B_3$			$0k_00$ $2_1$	$B_3$	$h_ek_00$ $b$	$A_2 B_2$ $A_3$			$0k_00$ $2_1$
64 $B2/m2_1/a2/b$	$0k_00$ $b, 2_1$	$A_2 B_2$ $A_3 B_3$			$0k_00$ $2_1$	$B_3$	$h_ek_00$ $b$	$A_2 B_2$ $A_3$			$h_00l_0$ $a$ $0k_00$ $2_1$	$A_2 B_2$ $A_3$ $A_2 B_2$ $B_3$
65 $B2/m2/m2/m$												
66 $B2/b2/m2/b$	$0k_00$ $b_2$	$A_3$			$0k_00$ $b_1$	$A_3$	$h_ek_00$ $b_2$	$A_2 B_2$ $A_3$	$0k_0l_e$ $b_1$	$A_2 B_2$ $A_3$		
67 $B2/m2/a2/m$											$h_00l_0$ $a$	$A_2 B_2$ $A_3$
68 $B2/b2/a2/b$	$0k_00$ $b_2$	$A_3$			$0k_00$ $b_1$	$A_3$	$h_ek_00$ $b_2$	$A_2 B_2$ $A_3$	$0k_0l_e$ $b_1$	$A_2 B_2$ $A_3$	$h_00l_0$ $a$	$A_2 B_2$ $A_3$

Table (b) HOLZ GM line table

Incident beam direction Space group	[100]		[010]		[001]		[uv0]		[0vw]		[u0w]	
	63 $B2/m2_1/m2/b$	$h_ek_00$ $b$	$A$	$h_ek_00$ $b$	$A$			$h_ek_00$ $b$	$A_h$			
64 $B2/m2_1/a2/b$	$h_ek_00$ $b$ $h_00l_0$ $a$	$A$	$h_ek_00$ $b$	$A$	$h_00l_0$ $a$	$A$	$h_ek_00$ $b$	$A_h$			$h_00l_0$ $a$	$A_h$
65 $B2/m2/m2/m$												
66 $B2/b2/m2/b$	$h_ek_00$ $b_{23}$	$A$	$0k_0l_e$ $b_{11}$ $h_ek_00$ $b_{23}$	$A$	$0k_0l_e$ $b_{11}$	$A$	$h_ek_00$ $b_{23}$	$A_h$	$0k_0l_e$ $b_{11}$	$A_h$		
67 $B2/m2/a2/m$	$h_00l_0$ $a$	$A$			$h_00l_0$ $a$	$A$					$h_00l_0$ $a$	$A_h$
68 $B2/b2/a2/b$	$h_ek_00$ $b_{23}$ $h_00l_0$ $a$	$A$	$0k_0l_e$ $b_{11}$ $h_ek_00$ $b_{23}$	$A$	$h_00l_0$ $a$ $0k_0l_e$ $b_{11}$	$A$	$h_ek_00$ $b_{23}$	$A_h$	$0k_0l_e$ $b_{11}$	$A_h$	$h_00l_0$ $a$	$A_h$

These tables were rewritten to the B-centered lattice instead for the C-centered one which is used as the standard notation in the International Tables for X-ray Crystallography and in an appendix in the present book.

## Fe<sub>3</sub>O<sub>4</sub>

Magnetite (Fe<sub>3</sub>O<sub>4</sub>) is of the spinel structure belonging to a space group *Fd3m* at room temperature. Verwey *et al.* reported that Fe<sub>3</sub>O<sub>4</sub> underwent a phase transition at about  $-150^{\circ}\text{C}$ , accompanied by the ordering of ions Fe<sup>+2</sup> and Fe<sup>+3</sup> [a]. This result had been believed to be correct until satellite reflections were found by X-ray and electron diffraction. Since then, a large number of studies on the phase transformation has been reported. The space group of the low temperature phase appears to have been established by Iizumi *et al.* as *Cc* [b]. An observation of the magnetoelectric effect [c], [d], however, implied that the space group must be *P1*, although the atomic displacements which violate the *c*-glide plane have been considered to be extremely small. Using CBED, we examined the space group of the low temperature phase. The crystallographic indexing was carried out using a monoclinic system, as was done by Iizumi *et al.* [b].

Photograph (a) shows a  $[001]_m([001]_c)$  zone-axis CBED pattern taken at the Liq.N<sub>2</sub> temperature. Its central part was enlarged to make clear the details of the symmetries in the weak reflection disks (Photo (b)). A mirror symmetry perpendicular to the  $[010]_m$  exists in the whole pattern. Photograph (c) shows a  $[110]_m([100]_c)$  zone axis CBED pattern. Seven weak reflections are seen between two strong reflections along the  $[001]_m$  direction. The strong  $008_m$  reflection is indexed as  $004_c$ , indicating a cell doubling in the  $[001]_m$  direction. A close inspection revealed that there is no symmetry in the pattern (c). Note especially that there is no mirror symmetry perpendicular to the  $[001]_m$ . These results indicate the point group to be *m*.

The diffraction pattern (d) was taken at the  $[001]_m$  incidence, the pattern (e) being the central part of (d). It is seen that the reflections of  $h+k=2n+1$  are forbidden (e). Hence, the lattice type is C-centered. As a result, the possible space groups are *Cm* and *Cc*. It is noted that there are two HOLZ rings in (d). The inner ring is characteristic of the low temperature phase and indicates again that the lattice parameter *c* is twice that at room temperature.

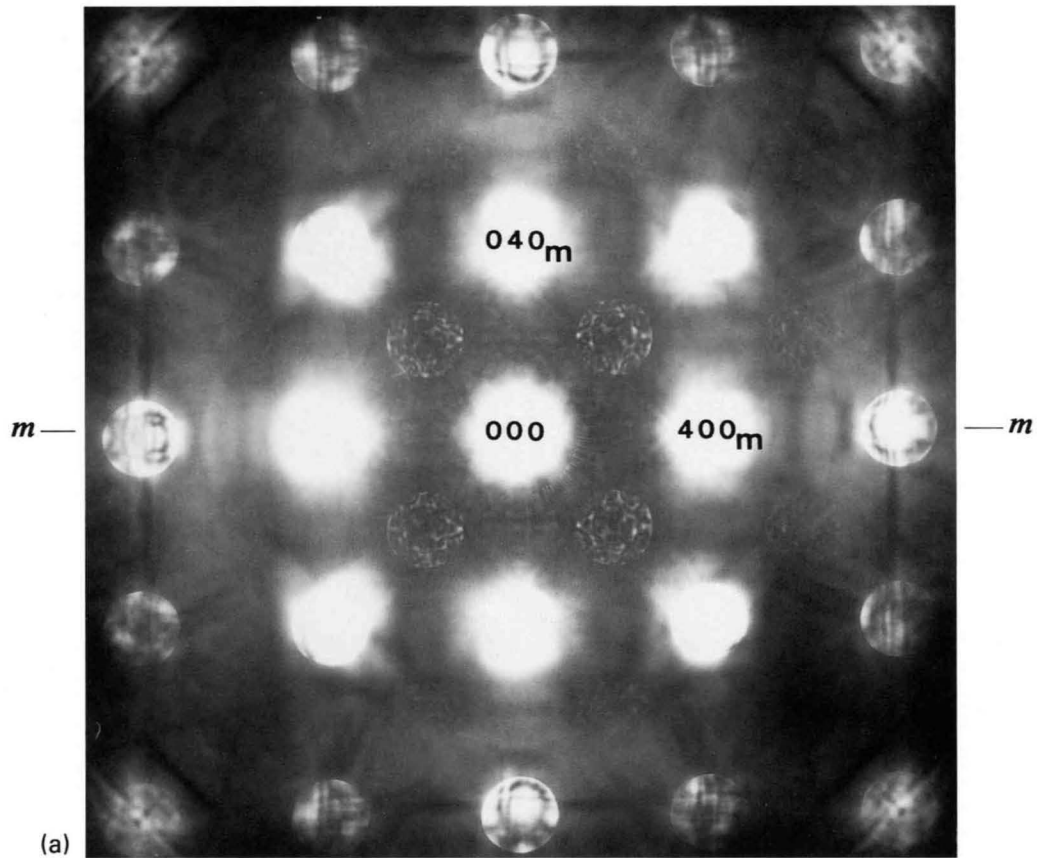
Photograph (f) shows CBED patterns taken with the  $[100]_m$  incidence at different accelerating voltages. Clear *A*<sub>2</sub> GM lines are seen in the  $00l(l=\text{odd})$  reflections of all the photographs. It is noted that the photographs needed an about 3-minute exposure even using our JEM-100CX/FEG. The result proved the existence of a *c*-glide plane. There was no indication that the *c*-glide plane was lost. Photograph (g) is a  $[100]_m$  CBED pattern covering a wide angular range. GM lines due to the *c*-glide plane are seen in the HOLZ reflections of  $2\ 0\ \bar{4}3_m$  and  $2\ 0\ 43_m$ . Thus, the space group of the low temperature phase was unambiguously determined to be *Cc*, supporting the result of Iizumi *et al.* The CBED patterns never showed a possibility of triclinic symmetry.

The specimens were supplied by Mr. S. Todo of the Institute for Solid State Physics, University of Tokyo.

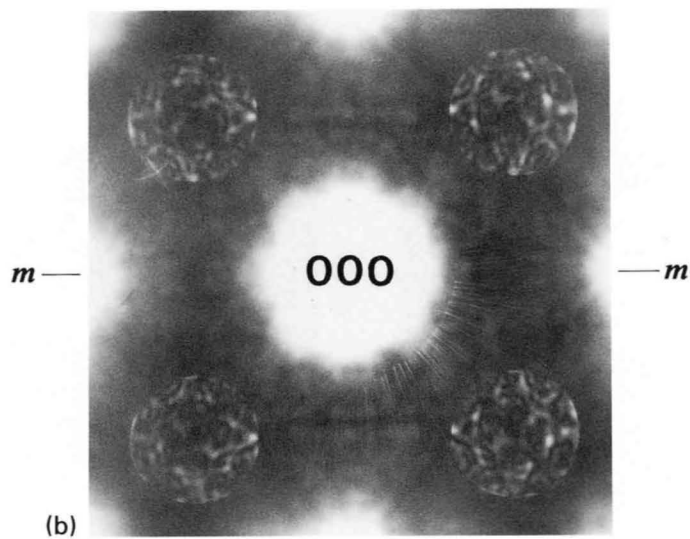
## References

- [a] E.J. Verwey, P.W. Haayman and F.C. Romeijn: *J. Chem. Phys.*, **15** (1947) 181.
- [b] M. Iizumi, T.F. Koetzle, G. Shirane, S. Chikazumi, M. Matsui and S. Todo: *Acta Cryst.*, **B38** (1982) 2121.
- [c] G.T. Rado and J.M. Ferrari: *Phys. Rev.*, **B15** (1977) 290.
- [d] K. Shiratori, E. Kita, G. Kaji, A. Tasaki, S. Kimura, I. Shindo and K. Kohn: *J. Phys. Soc. Jpn.*, **47** (1979) 1779.

$[001]_m$   $-186^\circ\text{C}$  60 kV

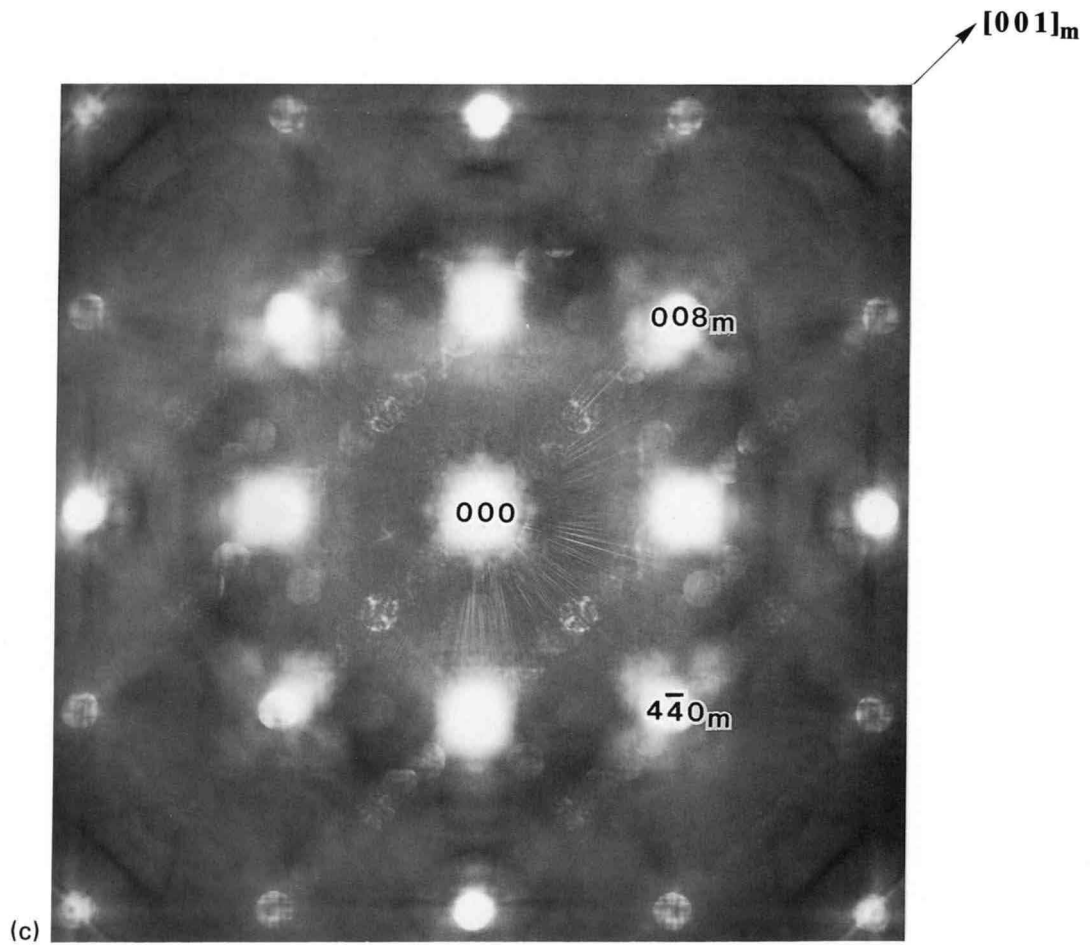


ZAP showing a mirror symmetry.



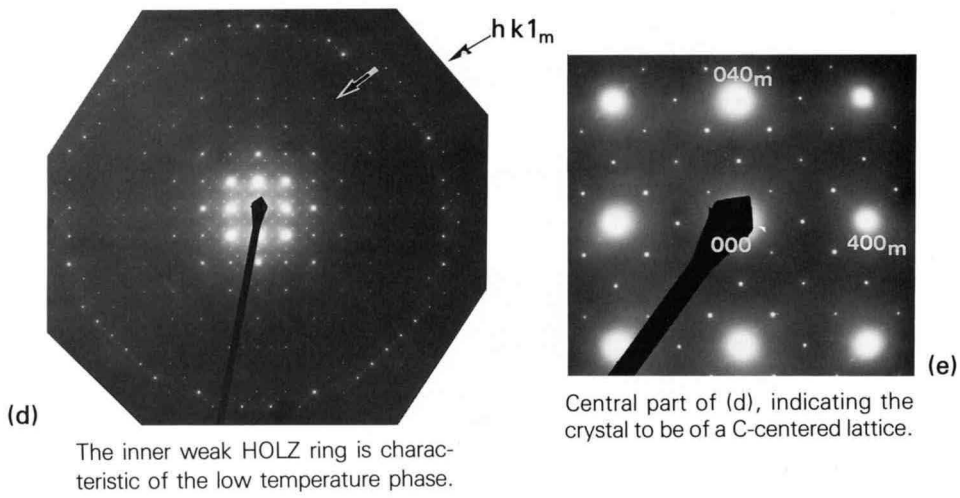
Central part of (a).

$\text{Fe}_3\text{O}_4$   $[110]_m$   $-186^\circ\text{C}$  60 kV



(c) ZAP showing symmetry 1.

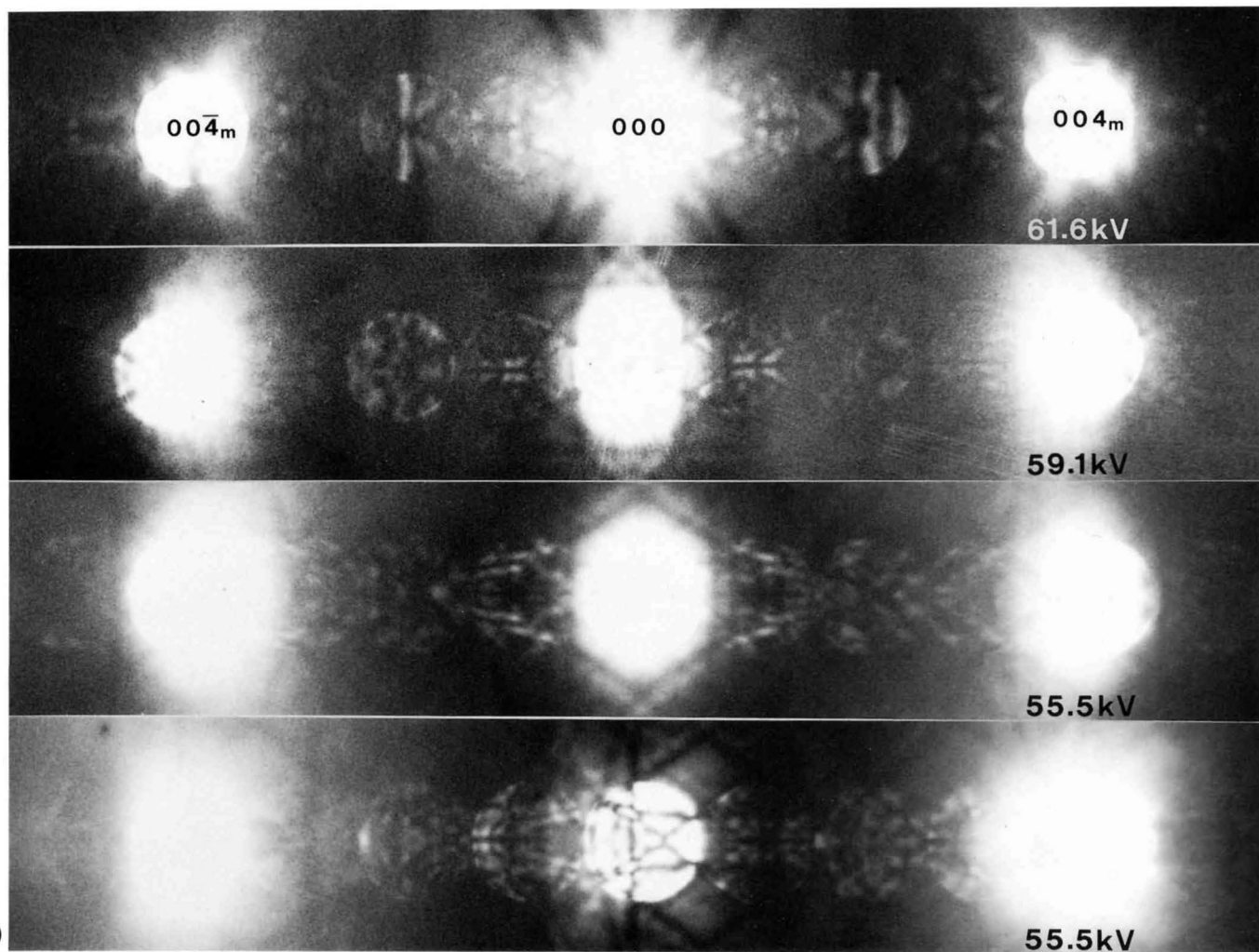
$[001]_m$



(d) The inner weak HOLZ ring is characteristic of the low temperature phase.

(e) Central part of (d), indicating the crystal to be of a C-centered lattice.

$[100]_m$   $-186^\circ\text{C}$

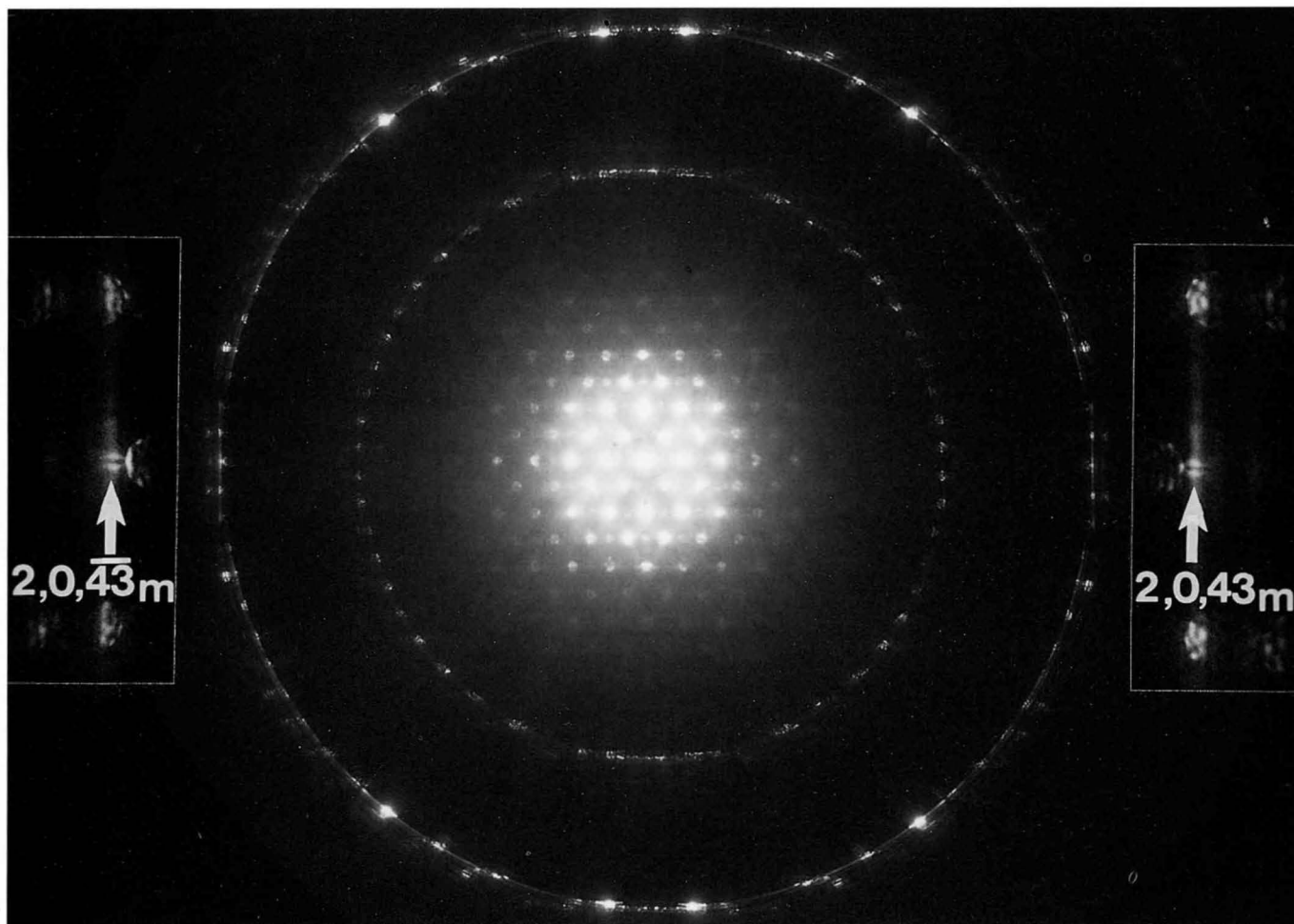


(f)

Odd order reflections are characteristic of the low temperature phase and show  $A_2$  GM lines due to the  $c$ -glide plane. The upper three patterns were taken at the zone-axis incidence and the lowest pattern at the  $001_m$  excitation.

**Point group  $m$**

Incident beam direction	$[u0w]$	
Space group		
6 $Pm$		
7 $Pc$	$h0l_0$ $c$	$A_2$ $B_2$ $A_3$
8 $Cm$		
9 $Cc$	$h_e0l_0$ $c$	$A_2$ $B_2$ $A_3$



(g)

Two HOLZ reflections show a type  $A_h$  GM line due to the  $c$ -glide plane. The GM lines look like type  $A$ , owing to the  $a$  axis is approximately perpendicular to the  $c$  axis.

Point group  $m$

Incident beam direction	$[u0w]$	
Space group		
6 $Pm$		
7 $Pc$	$h0l_0$ $c$	$A_h$
8 $Cm$		
9 $Cc$	$h_e0l_0$ $c$	$A_h$

# *Incommensurate Phases*

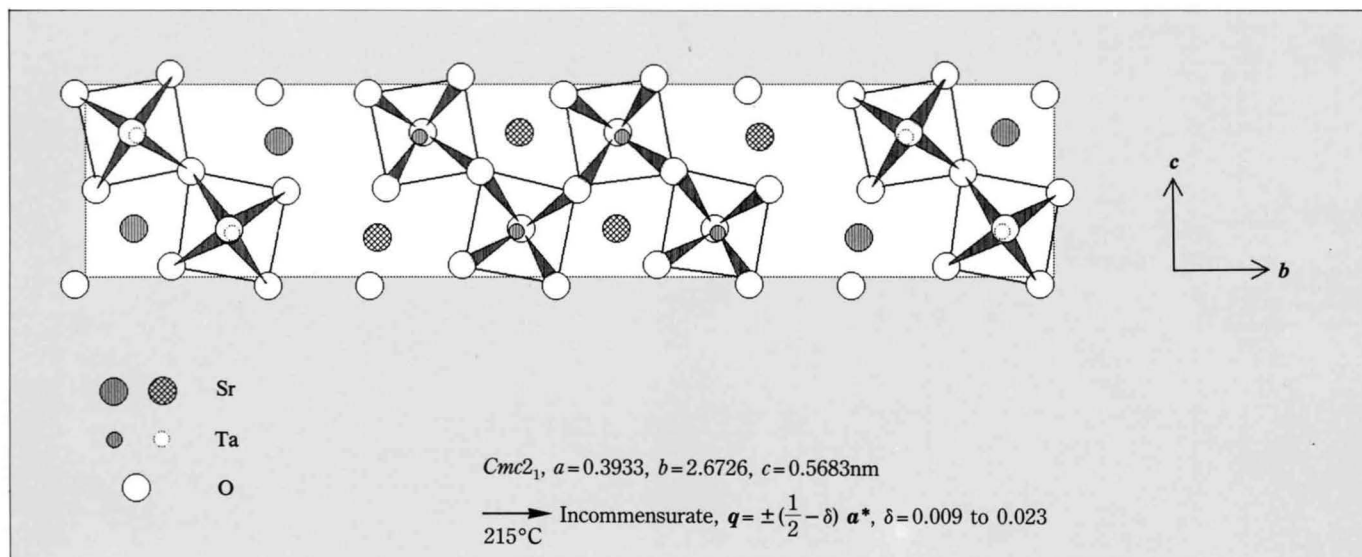
# Sr<sub>2</sub>Nb<sub>2</sub>O<sub>7</sub>

Many materials of the A<sub>2</sub>B<sub>2</sub>O<sub>7</sub> family undergo phase transformations from the space group *Cmcm* to *Cmc2<sub>1</sub>* to *P2<sub>1</sub>* with decreasing temperature. The phase transformation from *Cmcm* to *Cmc2<sub>1</sub>* has been reported to occur due to the rotation of the oxygen octahedra about the *a* axis with a slight deformation of the octahedra. The transformation from *Cmc2<sub>1</sub>* to *P2<sub>1</sub>* has been considered to be caused by the rotation of the octahedra about the *b* axis. An incommensurate phase appears, for example, in La<sub>2</sub>Ti<sub>2</sub>O<sub>7</sub> [a] between the phase with the space group *Cmc2<sub>1</sub>* and that with *P2<sub>1</sub>*. Sr<sub>2</sub>Nb<sub>2</sub>O<sub>7</sub> transforms from the phase with *Cmc2<sub>1</sub>* into an incommensurate phase, but does not transform into the phase with *P2<sub>1</sub>*. No discommensuration has been observed even at lower temperatures in the incommensurate phase. It was reported by Yamamoto [b] and Yamamoto & Ishizuka [c] that the modulated structures in this phase can be explained by the rotation of the oxygen octahedra about the *b* axis. We reexamined the symmetries of the phase using CBED.

A diffraction pattern (a) shows zig-zag arrays of the incommensurate reflections in the [0 $\bar{1}$ 1] direction. The indexing of the observed reflections was carried out using the indices of the phase with *Cmc2<sub>1</sub>*. CBED patterns (b) and (c) were taken at the [100] and [201] incidences. Since the pattern (b) does not have incommensurate reflections, its symmetries are produced by the average structure. The 00*l* (*l*=odd) reflections show A<sub>2</sub> GM lines, and the HOLZ ring of this pattern (not seen here) showed a mirror symmetry perpendicular to the *b* axis. These indicate the existence of a *c*-glide plane parallel to the (010) plane.

The incommensurate reflections in the CBED pattern (c) show a mirror symmetry perpendicular to the *b* axis. It is unfortunately not possible to know directly from GM lines whether the modulated structure preserves the *c*-glide plane, because no incommensurate reflections appear on the [102] axis. If the modulation does not violate the *c*-glide plane, the glide plane gives rise to a mirror symmetry, which is observed in Photo (c). Reference to the structure of the high temperature phase with *Cmc2<sub>1</sub>* (see the figure) allows concluding that the modulation does not change the *c*-glide symmetry into a mirror symmetry. Therefore, the *c*-glide plane should still be preserved in the incommensurate phase.

Photograph (d) shows a [010] CBED pattern, its central part being enlarged in Photo (e). The strong fundamental reflections due to the average structure have a mirror symmetry perpendicular to the *a* axis, presumably due to little interaction between the fundamental and the incommensurate reflections. The incommensurate reflections do not have a mirror symmetry. Hence, the modulated structure violates the (100) mirror plane in the high temperature phase. If the average structure has a 2<sub>1</sub> screw axis parallel to the *c* axis, A<sub>2</sub> GM lines appear in the 001 and 00 $\bar{1}$  reflections. No GM lines were observed in these reflections. A plausible explanation of this fact is that the modulated structure does not have the 2<sub>1</sub> screw axis and violates the GM lines due to a strong dynamical diffraction effect between the weak fundamental reflections and the neighbouring incommensurate reflections.



Structure of Sr<sub>2</sub>Nb<sub>2</sub>O<sub>7</sub>. Space group: *Cmc2<sub>1</sub>*

The CBED pattern (f) was taken by tilting the specimen a few degrees from the [110] axis about the  $c$  axis, the pattern (g) being the central part of (f). Incommensurate reflections are seen but do not strongly interact with the fundamental reflections. As a result, a  $B_2$  GM line due to the  $2_1$  screw axis is clearly seen in the 001 reflection. This indicates that the average structure has a  $2_1$  screw axis in the  $c$  direction. These results are summarized in the table. That is, the average structure does not have the space group  $P2_1$  of the expected low temperature phase but has the same space group as that of the high temperature phase. This result is acceptable from the fact that neither the lower temperature phase with  $P2_1$  nor discommensuration have been observed. The modulated structure preserves only the (010) mirror plane.

The rotation of the oxygen octahedra about the  $b$  axis, which was previously proposed as a mechanism of the phase transition, preserves the  $2_1$  screw axis but violates the  $c$ -glide plane parallel to the (010) plane. Thus, this mechanism is incompatible with the present experimental result. A rotation about the  $c$  axis preserves the  $c$ -glide plane but loses the  $2_1$  screw axis, which is compatible with the present experimental result. This rotation itself introduces only the doubling of the cell parameter  $a$ , but does not produce the  $q$  value of the incommensurate phase. Thus, displacements of atoms to produce the  $q$  value must be considered additionally.

The modulation may be better explained by a sinusoidal displacement wave  $u$ ,

$$u = \xi \cos 2\pi(q \cdot r - \nu t),$$

where  $\xi$  is the amplitude vector and  $q = (1/2 - \delta)a^*$ . The intensity of the reflection  $H$  is expressed as

$$I = 2\pi |F|^2 (\xi \cdot H)^2$$

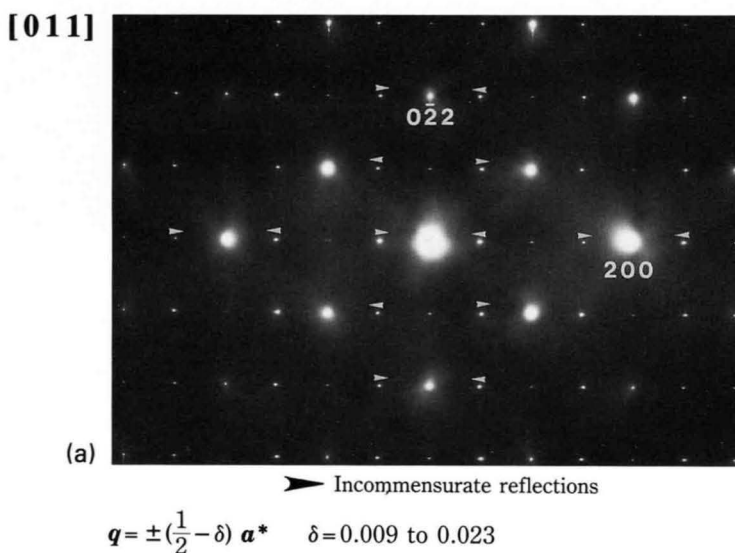
where  $F$  is the crystal structure factor of the reflection. When a longitudinal wave ( $\xi // a$ ) is assumed to occur, the positions of the incommensurate reflections in Photo (a) are well explained. This wave causes the (100) mirror plane and  $2_1$  screw axis to be lost, but preserves the  $c$ -glide plane, which is compatible with the result of our CBED experiment. Therefore, the modulated structure in the incommensurate phase may be approximated by a sinusoidal longitudinal displacement wave.

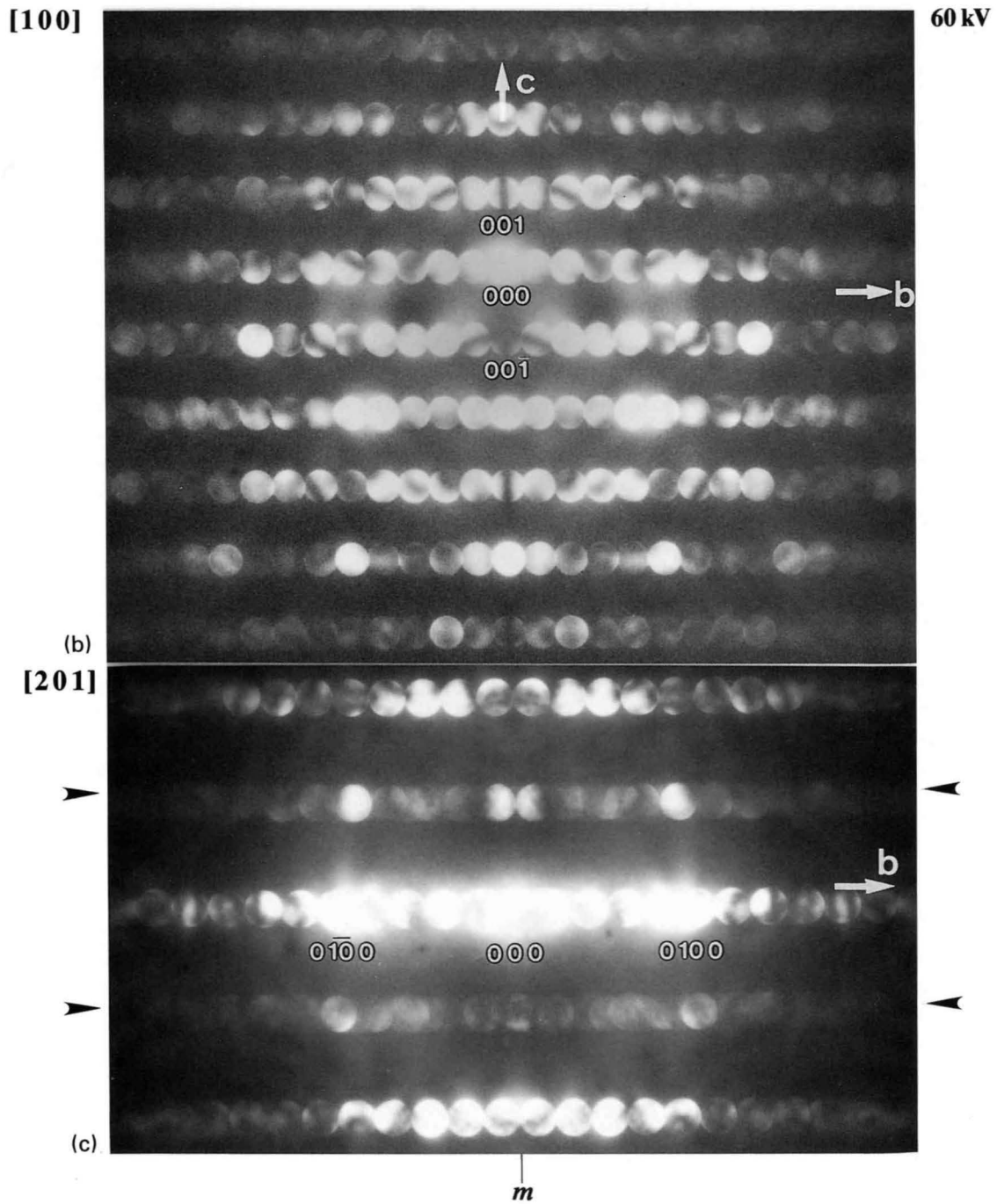
Such a CBED study of the incommensurate phase definitely gives a useful guide to the structure analysis even in the scope of three dimensional crystallography.

The specimens were supplied by N. Yamamoto of Faculty of Engineering, the Technological University of Nagaoka.

#### References

- [a] M. Tanaka, H. Sekii and K. Oki: *Jpn. J. Appl. Phys.*, **24** (1985) Suppl. 24-2, 814.
- [b] N. Yamamoto: *Acta Cryst.*, **A38** (1982) 780.
- [c] N. Yamamoto and K. Ishizuka: *Acta Cryst.*, **B39** (1983) 210.

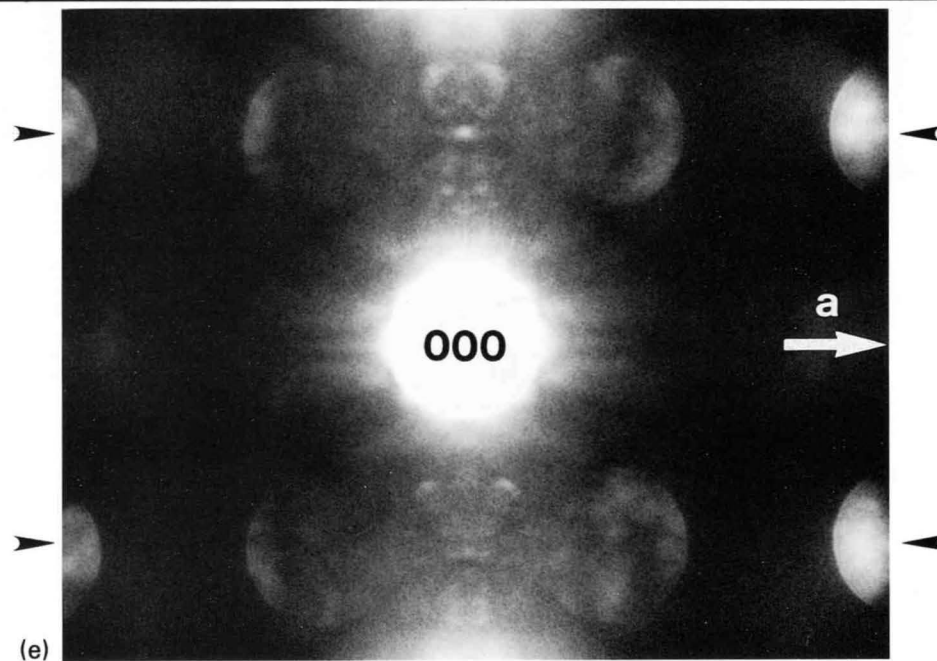
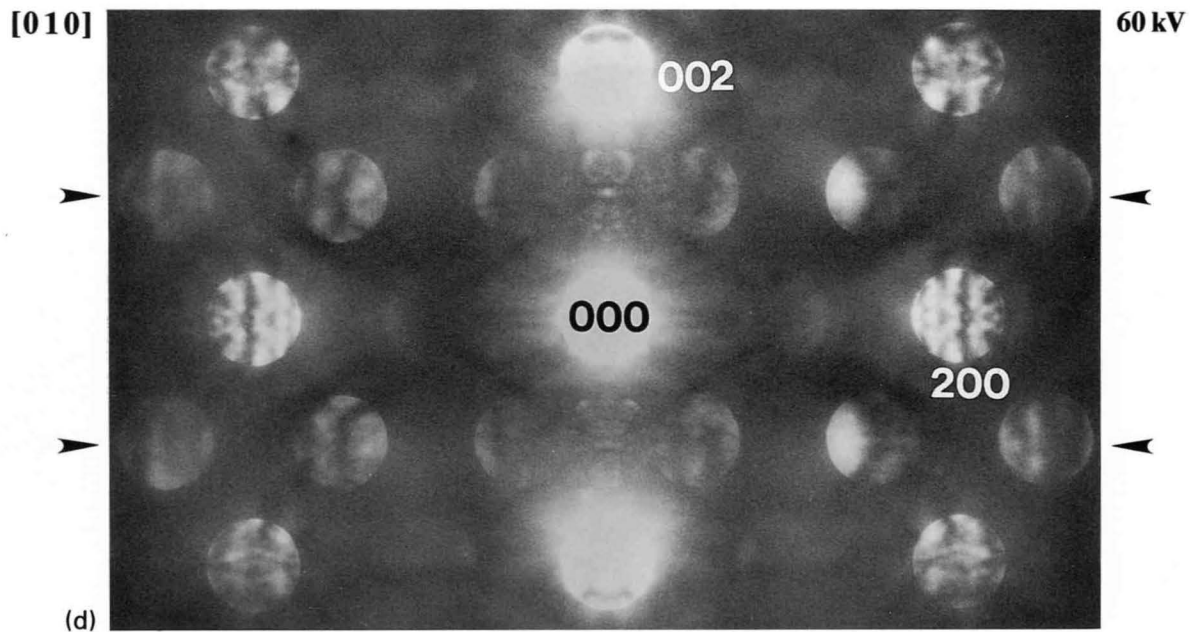




➤ Incommensurate reflections

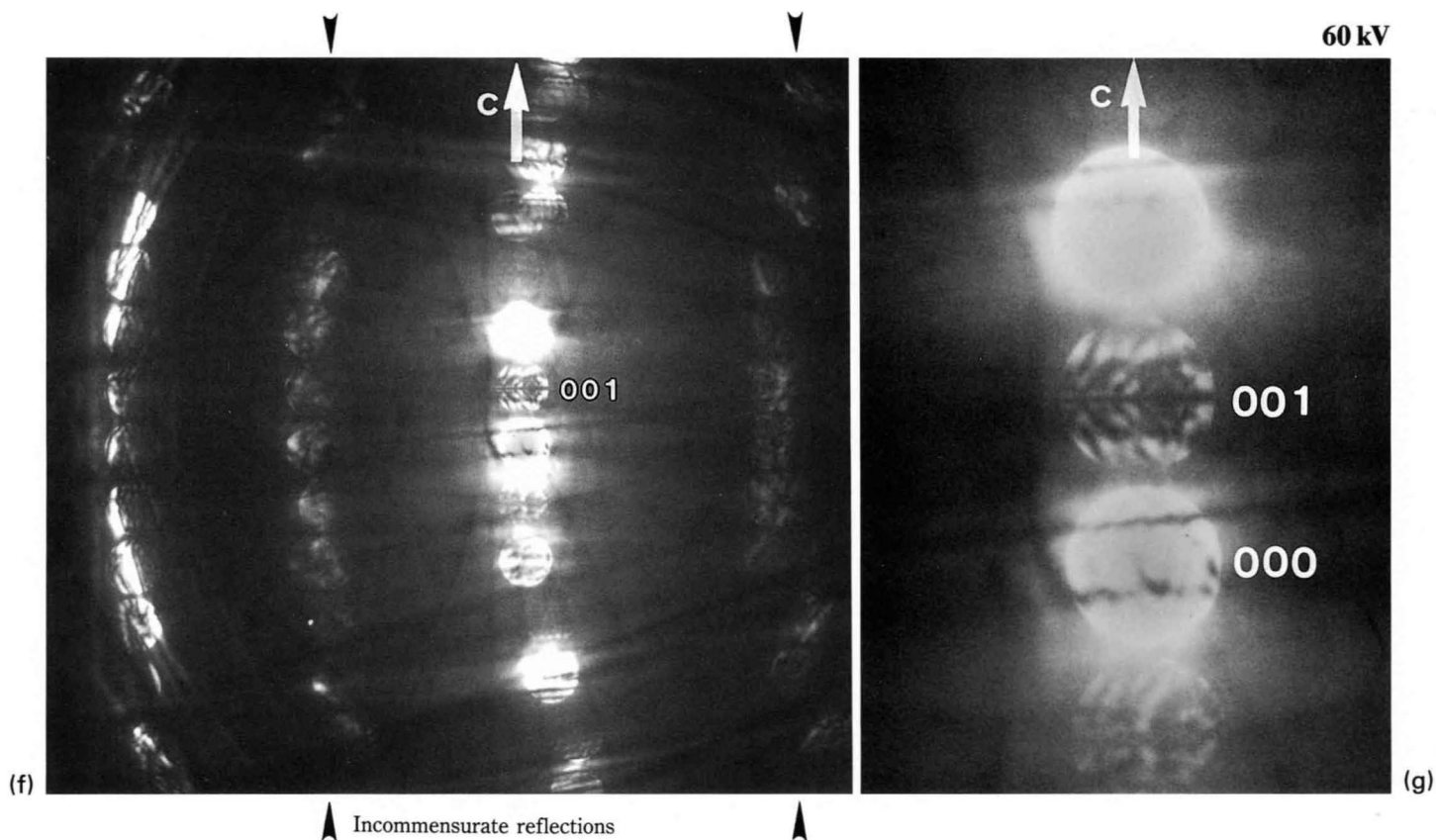
(b) No incommensurate reflection is seen. GM lines are seen in the  $00l$  ( $l = \text{odd}$ ) reflections.

(c) Incommensurate reflections show a mirror symmetry.



➤ Incommensurate reflections

(d) Fundamental reflections show a mirror symmetry perpendicular to the  $a$  axis, but incommensurate reflections do not.



▲ Incommensurate reflections

The specimen was tilted from the [110] zone axis about the [001] axis.  $B_2$  GM line is seen in the 001 reflection.

Enlarged pattern of the central part of (f).

	<i>a</i>	<i>b</i>	<i>c</i>
Fundamental reflections	$\sim m$	<i>c</i>	$\sim 2_1$
Incommensurate reflections	—	$m(c)$	—

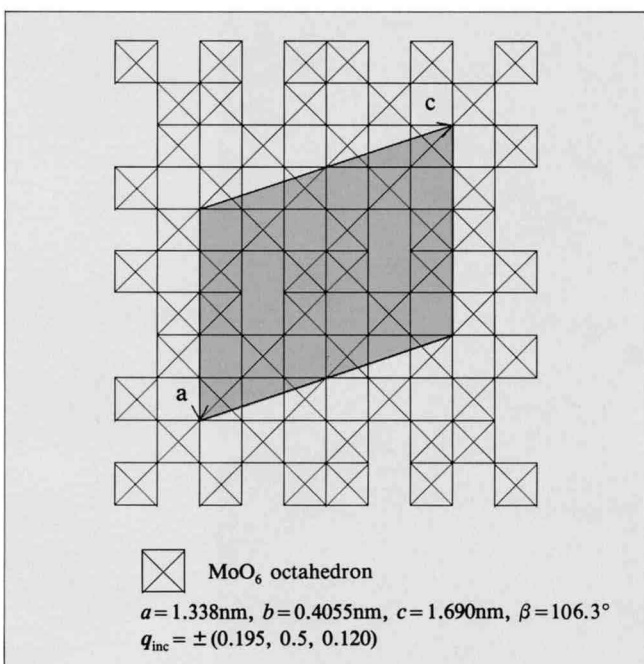
# Mo<sub>8</sub>O<sub>23</sub>

A series of transition metal oxides Mo<sub>n</sub>O<sub>3n-1</sub> ( $n \geq 8$ ) is formed when metal-oxygen octahedra MoO<sub>6</sub> are combined. The figure shows a schematic diagram of the fundamental structure of Mo<sub>8</sub>O<sub>23</sub>. The high temperature form of this material belongs to a monoclinic space group *P2/c*, transforms at 42°C into an incommensurate phase characterized by a wave number vector of  $\mathbf{q} = (0.195, 0.5, 0.120)$  and undergoes at 12°C a lock-in phase transition to a phase with a space group *Pc* and the  $\mathbf{q} = (0, 0.5, 0)$ . It has been reported that the phase transitions are closely related to the formation of a charge density wave [a].

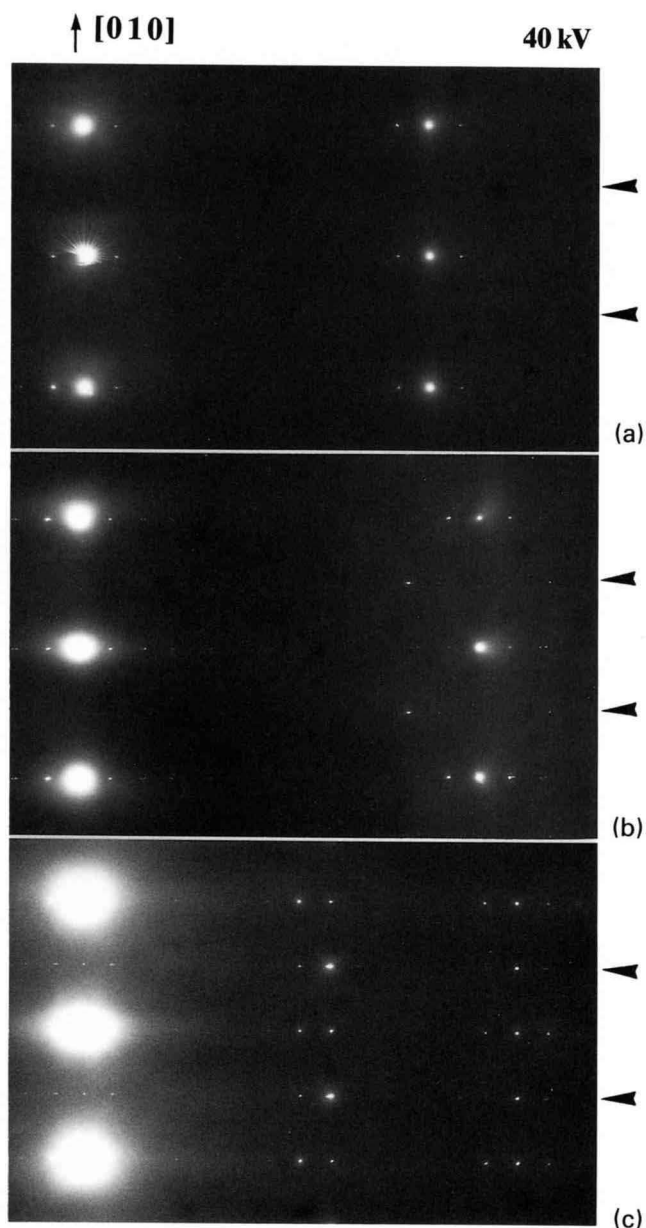
The diffraction patterns (a), (b) and (c) were taken respectively at 142°C, 20°C and -173°C and at different crystal settings by tilting the specimen by a few degrees from the [100] about the [010] axis. In Photo (b), incommensurate reflections are seen on the horizontal lines indicated by the black arrows, but no such reflections in Photo (a). It should be noted that only one reflection of an incommensurate reflection pair at  $\mathbf{q} = \pm(0.195, 0.5, 0.120)$  is seen in Photo (b) due to a nonzero value of the  $a^*$  component of  $\mathbf{q}$ . Photograph (c) shows superlattice reflections (commensurate) at  $\mathbf{q} = (0, 0.5, 0)$ .

In the [100] CBED pattern (d), incommensurate reflections are hardly seen. The presence of GM lines in the  $00l$  and  $10l$  ( $l = \text{odd}$ ) fundamental reflections indicates that the average structure has a *c*-glide plane. The CBED pattern (e) shows GM lines in the  $h0l$  ( $l = \text{odd}$ ) fundamental reflections and exhibits a mirror symmetry between in-

commensurate reflections shown by the arrows. These facts indicate that the incommensurate structure preserves the *c*-glide plane. The [010] CBED pattern (f) shows a twofold rotation symmetry not only in the outer HOLZ ring due to the fundamental structure but also in the inner weak HOLZ ring originating from the incommensurate structure. These results are summarized in the table, and indicate that the incommensurate phase has the same symmetries as the high temperature phase.

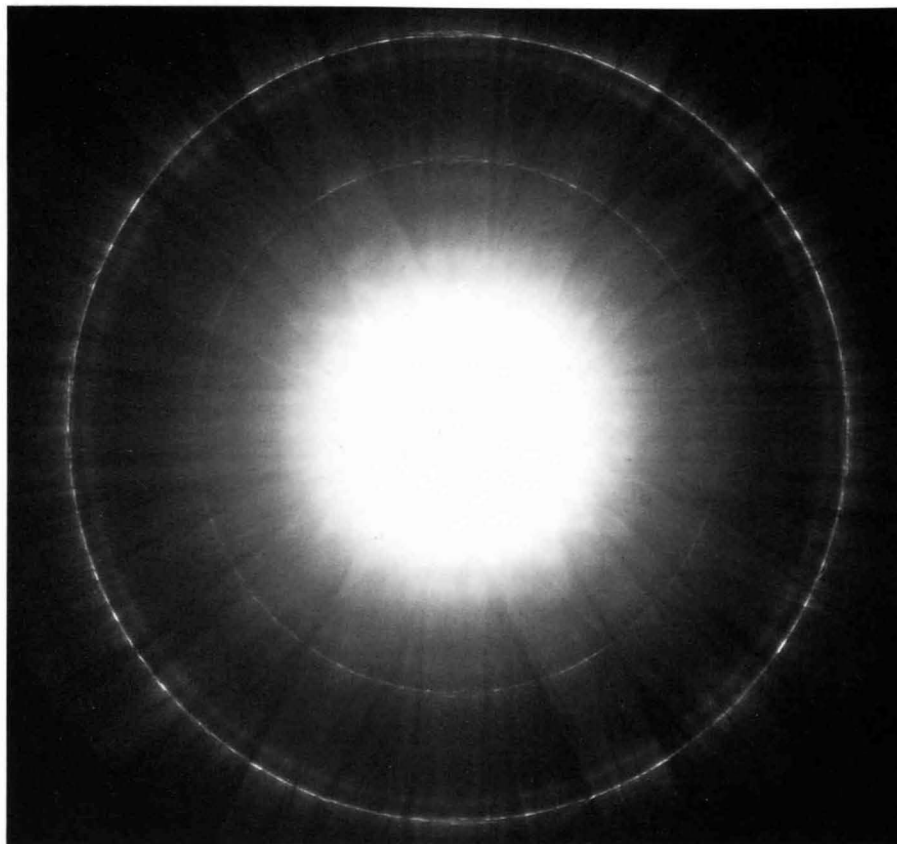


Structure of Mo<sub>8</sub>O<sub>23</sub>. Space group: *P2/c*





[010]



(f)

Outer and inner HOLZ rings showing symmetries 2.

It has been reported that the low temperature form with the space group  $Pc$  is produced by an  $M_3$  type rotation and a deformation of  $\text{MoO}_6$  octahedra [a]. An  $M_3$  type rotation of the octahedra without deformation appear to preserve the space group  $P2/c$  but produce a cell doubling in the [010] direction, giving rise to superlattice reflections at  $\mathbf{q} = (0, 0.5, 0)$ . An antiphase domain structure or a long-period superlattice (LPS) in the direction of [0.195, 0, 0.120] can explain the splitting of a superlattice reflection at  $\mathbf{q} = (0, 0.5, 0)$  into two reflections at  $\mathbf{q} = \pm(0.195, 0.5, 0.120)$ , where the incommensurate wave number is obtained by a uniform mixing of two LPSs with different but commensurate periods [b]. The LPS, which has a commensurate period, preserves twofold axes and  $c$ -glide planes existing in the high temperature phase. Therefore, in the incommensurate phase a long-period superlattice should be formed by an  $M_3$  type rotation of  $\text{MoO}_6$  octahedra without deformation accompanied by an antiphase domain structure.

The specimens were supplied by M. Sato of the Institute for Molecular Science.

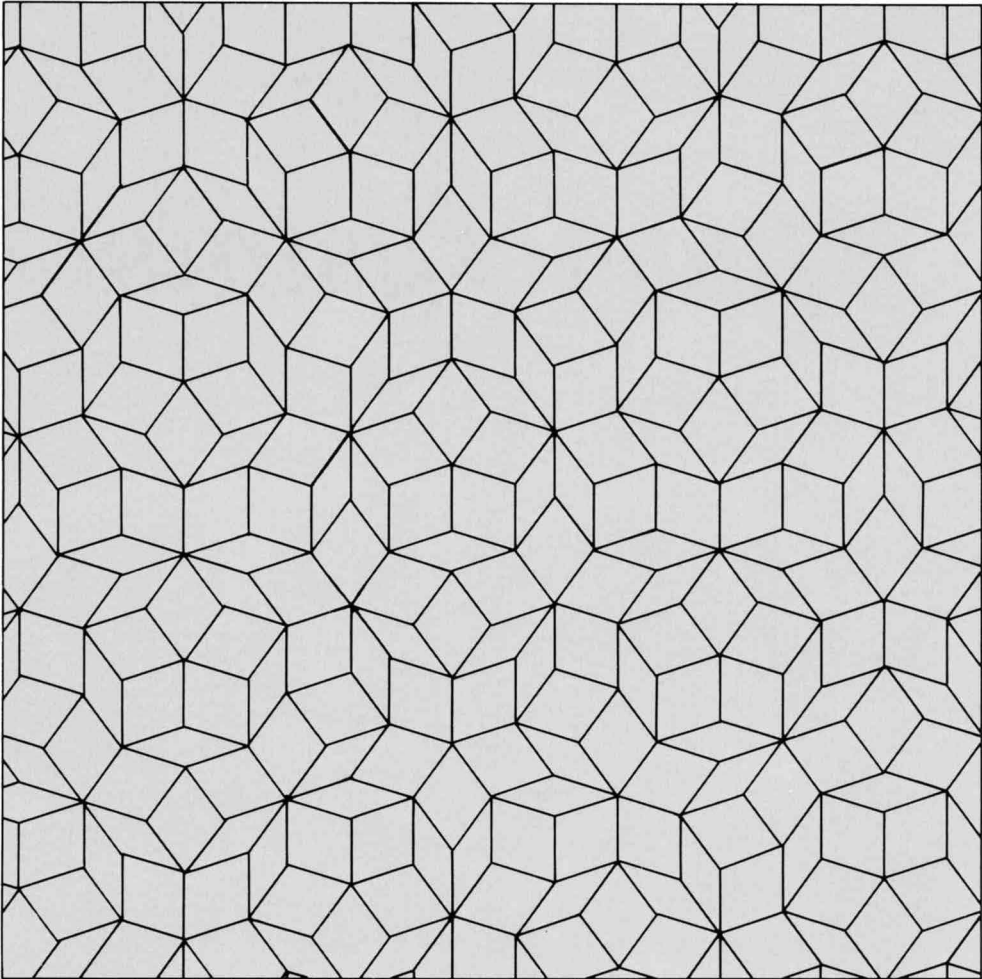
	b
Fundamental reflections	2, $c$
Incommensurate reflections	2, $m(c)$

#### References

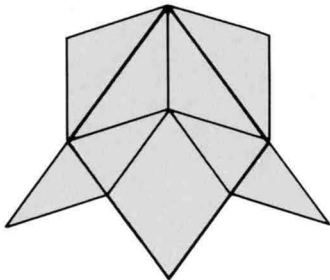
- [a] M. Sato, H. Fujishita, S. Sato and S. Hoshino: *J. Phys.*, **C19** (1986) 3059.  
 [b] K. Fujiwara: *J. Phys. Soc. Jpn.*, **12** (1957) 7.

# *Quasicrystals*

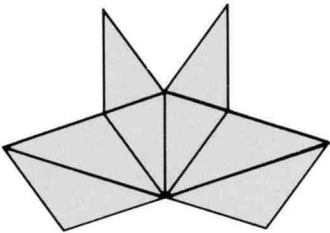
# Icosahedral Phases



Penrose tiling



Fat rhombus



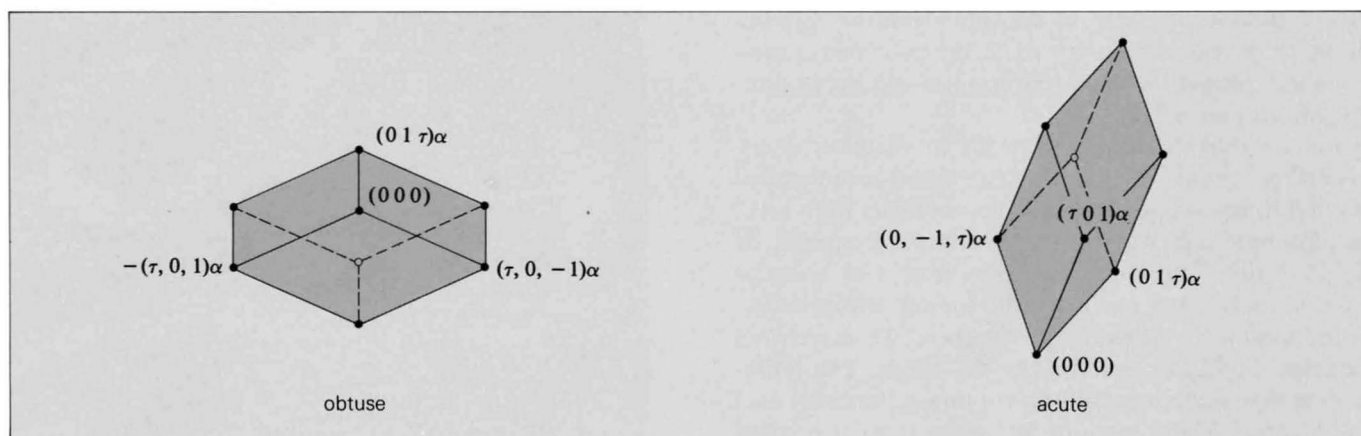
Thin rhombus

Penrose [a] demonstrated that the two dimensional plane can be tiled with thin and fat rhombi to give a pattern with local fivefold rotation symmetries but with no translational symmetry. Mackay [b] extended the tiling to three dimensions using acute and obtuse rhombohedra, which also resulted in acquisition of local fivefold symmetries and in vanishment of the translational symmetry. (The three dimensional space filling method was afterwards completed by Ogawa [c].) These, however, had remained a matter of design or amusement of geometry until Schechtman *et al.* [13] discovered an icosahedral symmetry presumably with a long-range structural order in an alloy of  $\text{Al}_6\text{Mn}$  (nominal composition), using electron diffraction. Since then, the new class of structural order, which has no translational symmetry but has a long-range structural order, has been called the “quasicrystal”. Levine and Steinhardt [d] showed that the quasi-lattice produces sharp diffraction patterns, and they succeeded in reproducing almost exactly the diffraction pattern obtained by Schechtman *et al.* using the Fourier transform of a quasi-periodic icosahedral lattice. They described that one of the important properties of the quasicrystal is self-similarity transformation.

Do real quasicrystals truly have an icosahedral symmetry with a long-range structural order and self-similarity transformation? We have examined icosahedral and decagonal quasicrystals using CBED and small-area-parallel-beam electron diffraction.

## References

- [a] R. Penrose: *Bull. Inst. Math. and Its Appl.*, **10** (1974) 266.  
 [b] A.L. Mackay: *Physica*, **114A** (1982) 609.  
 [c] T. Ogawa: *J. Phys. Soc. Jpn.*, **54** (1985) 3205.  
 [d] D. Levine and P.J. Steinhardt: *Phys. Rev. Lett.*, **53** (1984) 2477.



Two rhombohedra used to produce icosahedral quasicrystals. Unit edge length is  $\alpha = \sqrt{1 + \tau^2}$

## $\text{Al}_4\text{Mn}/\text{Al}_{74}\text{Mn}_{20}\text{Si}_6$

### $\text{Al}_4\text{Mn}$

First we investigated an alloy of the same composition [14] as that studied by Schechtman *et al.* [13], their quasicrystalline grains being later found to be of  $\text{Al}_4\text{Mn}$ . Photograph (a) shows an electron microscope image of the alloy. The grains of the quasicrystal were found to be less than 10 nm in size. All the CBED patterns obtained from an about 10 nm in diameter  $\times$  100 nm high volume did not at all exhibit any fivefold symmetry, although ordinary electron diffraction patterns showed a fivefold symmetry, as obtained by Schechtman *et al.* Small-area-parallel-beam electron diffraction patterns taken from about 100 nm diameter areas at an incidence along the fivefold axis made clear that the quasicrystal was highly strained. That is, 1) higher order Laue-zone reflections were not observed, 2) reflections due to lattice spacings greater than 1.37 nm did not appear, 3) the profiles of Kikuchi bands in five equivalent directions were not symmetric with respect to their centers, 4) each diffraction spot was composed of a number of fine spots and 5) three principal diffraction spots showed a zig-zag deviation from the radial line. Lubensky *et al.* interpreted the last result, 5), in terms of anisotropically quenched phason strains.

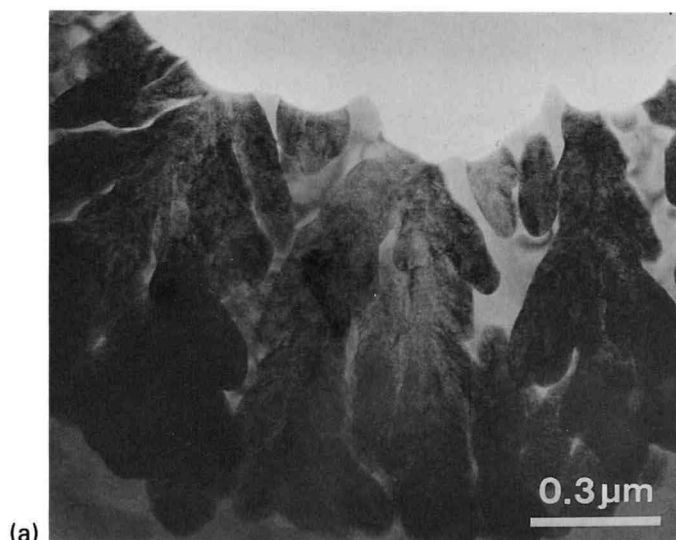
#### Reference

[a] T.C. Lubensky, J.E.S. Socolar, P.J. Steinhardt, P.A. Bancel and P.A. Heiney: *Phys. Rev. Lett.*, **57** (1986) 1440.

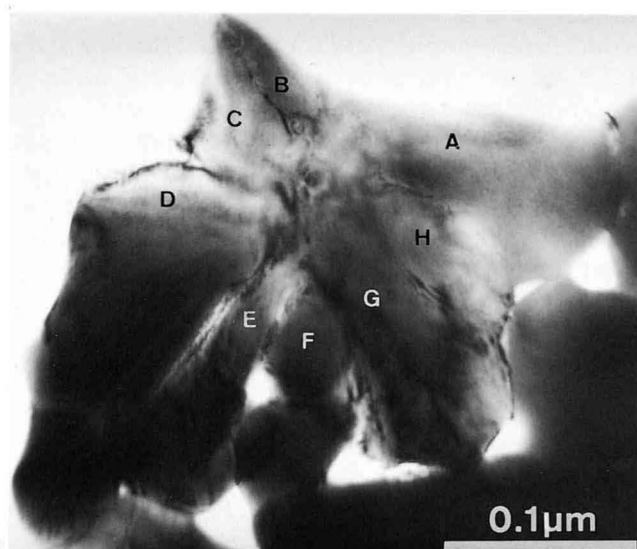
### $\text{Al}_{74}\text{Mn}_{20}\text{Si}_6$

The addition of several percent of silicon to Al-Mn alloys causes a large increase in the degree of order of the quasicrystal. Bendersky and Kaufman [15] prepared such a less strained quasicrystalline  $\text{Al}_{71}\text{Mn}_{23}\text{Si}_6$  alloy and determined its point group. They obtained fairly good zone-axis CBED patterns which showed symmetries of  $10mm$ ,  $6mm$  and  $2mm$  in ZOLZ disks and  $5m$ ,  $3m$  and  $2mm$  in HOLZ rings. From these results, they identified the point group to be centrosymmetric  $m\bar{3}5$ . We examined crystallographic properties of a less strained quasicrystalline  $\text{Al}_{74}\text{Mn}_{20}\text{Si}_6$  alloy [16].

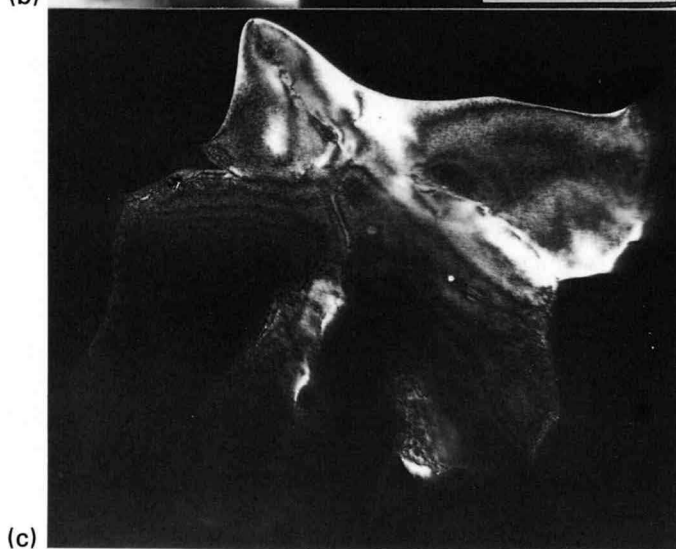
Photographs (b) and (c) show 0.1  $\mu\text{m}$  diameter quasicrystalline grains of  $\text{Al}_{74}\text{Mn}_{20}\text{Si}_6$ . Small-area-parallel-beam diffraction patterns (d) to (f) were taken from a 110 nm diameter area with an incident beam divergence of  $3 \times 10^{-5}$  rad. The innermost reflections with a lattice spacing of 2.27 nm in Photo (d). Among strong reflections, many weak diffraction spots appear, which were not observed in  $\text{Al}_4\text{Mn}$  and  $\text{Al}_{71}\text{Mn}_{23}\text{Si}_6$  alloys. The reflections at high scattering angles have a stronger intensity than in  $\text{Al}_4\text{Mn}$ . These results indicate that the alloy  $\text{Al}_{74}\text{Mn}_{20}\text{Si}_6$  has a much greater ordering than the other two.



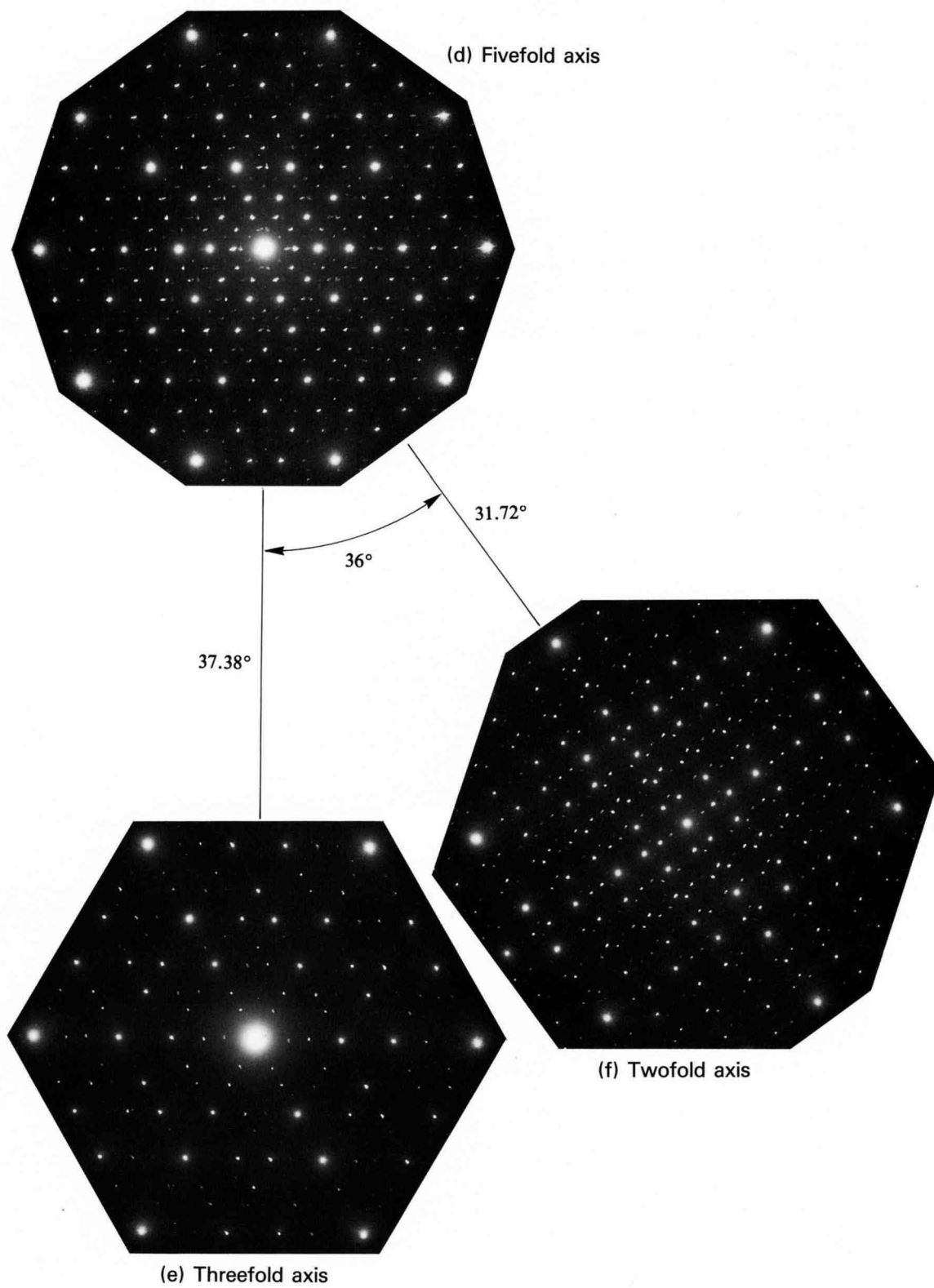
(a)



(b)

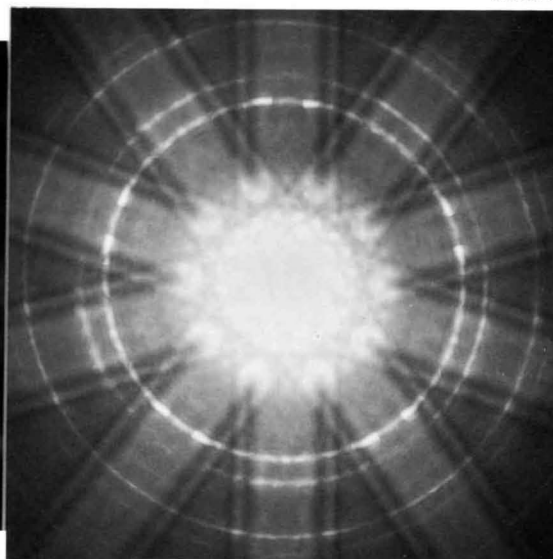
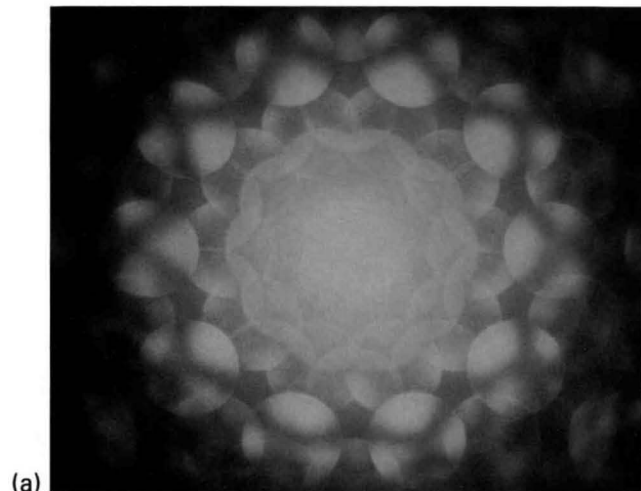


(c)



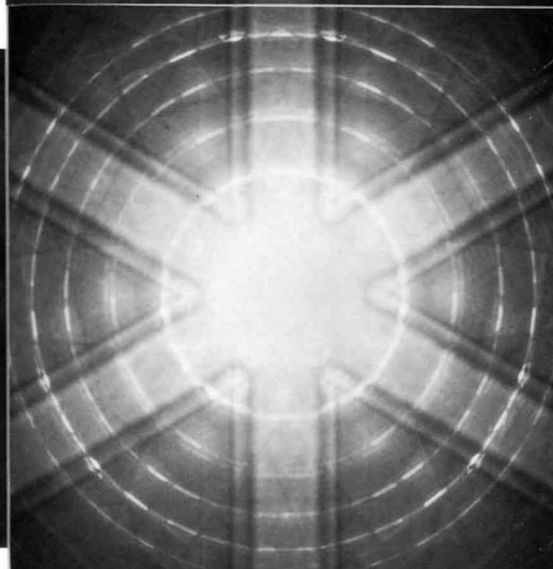
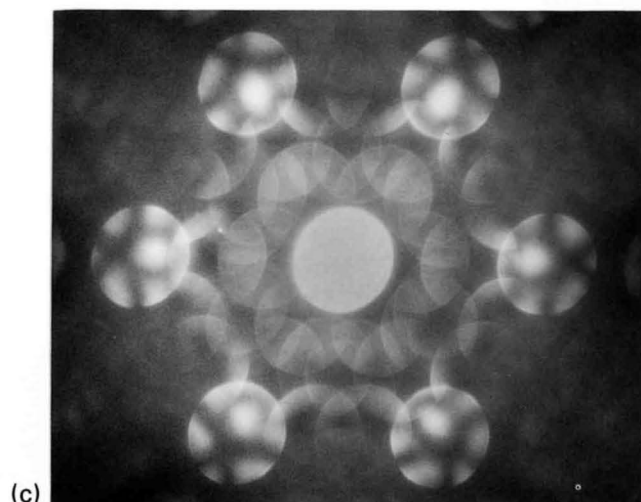
60 kV

Fivefold axis



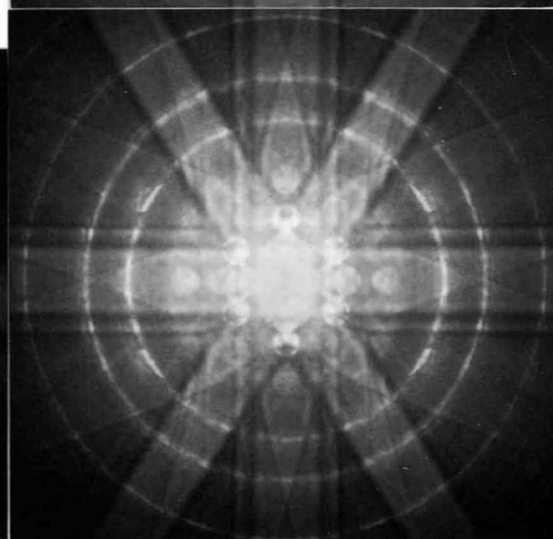
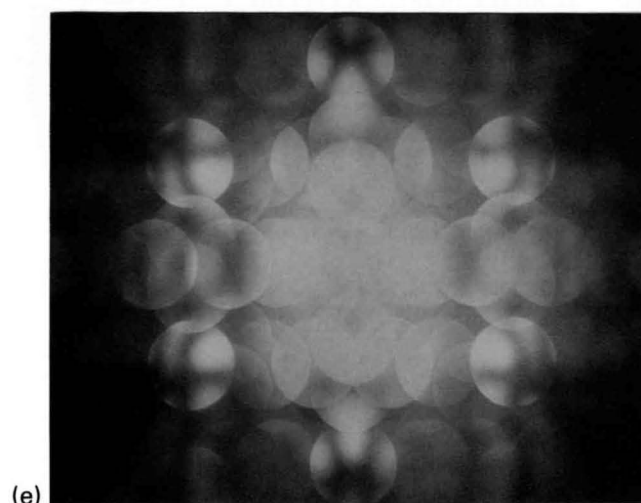
(b)

Threefold axis



(d)

Twofold axis



(f)

## Al<sub>74</sub>Mn<sub>20</sub>Si<sub>6</sub> — CBED patterns —

60 kV

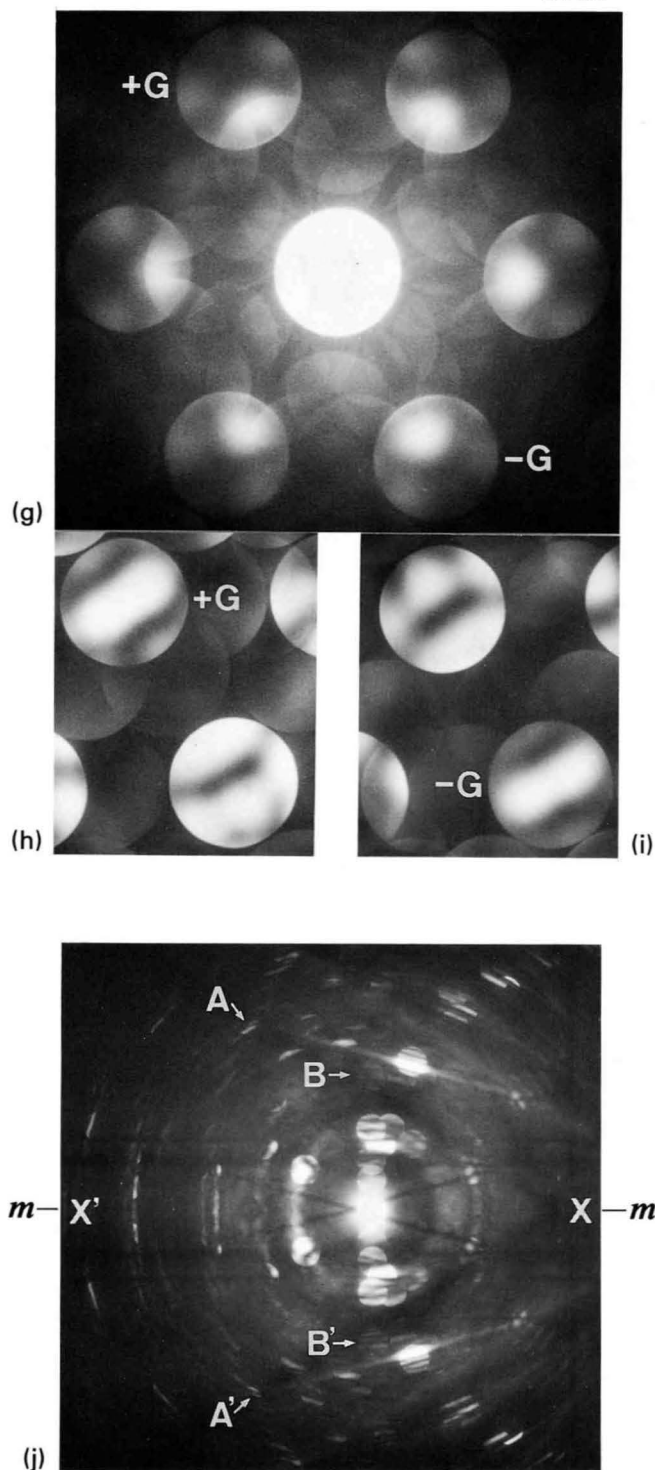
Photographs (a) to (f) show three pairs of CBED patterns taken from an about 100 nm thick and about 3 nm diameter area of an Al<sub>74</sub>Mn<sub>20</sub>Si<sub>6</sub> quasicrystal at an accelerating voltage of 60 kV. Each pair consists of a ZOLZ pattern and a HOLZ pattern. The former pattern is produced almost by the interaction of ZOLZ reflections. Distinct symmetries are seen in several disks. Many HOLZ rings and Kikuchi bands are clearly seen in the HOLZ patterns. The profiles of Kikuchi bands are symmetric with respect to their centers ( (b), (d) and (f) ). These results contrast strongly with those of Al<sub>4</sub>Mn, and indicate that the constituent atoms form a highly ordered arrangement of the quasicrystal.

The whole pattern (a), formed by ZOLZ reflections, exhibits a tenfold rotation and two types of mirror symmetries, the resultant symmetry being expressed as  $10mm$ . The whole pattern (b), formed by HOLZ reflections, is seen to show a fivefold symmetry and a type of mirror plane, the resultant symmetry being expressed as  $5m$ . Photographs (c) and (d) show symmetries  $6mm$  and  $3m$ , respectively. Photographs (e) and (f) show a symmetry  $2mm$ .

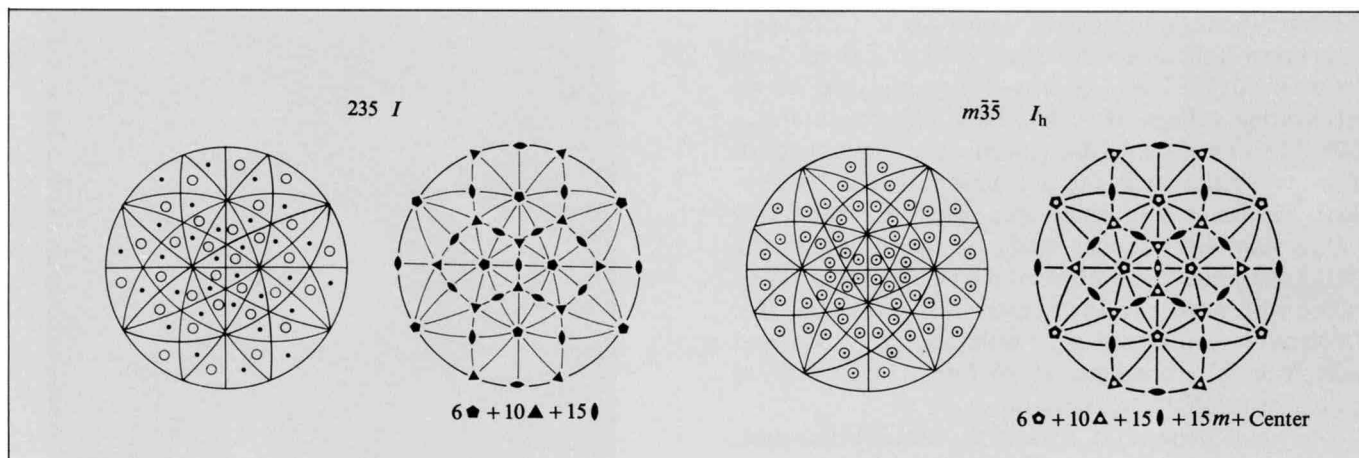
It is known that there exist two icosahedral point groups  $235$  and  $m\bar{3}5$ . The former is noncentrosymmetric and has no mirror symmetry, but the latter is centrosymmetric. The table in the next page shows diffraction groups expected from these point groups at an incident beam parallel to the fivefold axis and their symmetries appearing in WP, BP, DP and  $\pm$ DP. Projection diffraction groups and their symmetries, in which only the interaction between ZOLZ reflections is taken into account, are written in the second row. Diffraction groups obtained at other incident beam orientations are omitted, since these have been given in the references [1] and [5]. The whole pattern symmetries observed in the present quasicrystal agree with those expected from point group  $m\bar{3}5$ , which was obtained by Bendersky & Kaufman [15].

Photograph (g) shows a zone-axis CBED pattern taken at an electron incidence along the threefold axis. Photographs (h) and (i) show a pair of  $\pm G$ -dark-field CBED patterns. The pattern of the  $+G$ -dark-field disk coincides with that of the  $-G$ -disk when the former is superposed on the latter with a translation of  $-2G$ . This symmetry,  $2_R$ , directly proves that the quasicrystal is centrosymmetric, again indicating the point group to be  $m\bar{3}5$ .

It is noted, however, that the above symmetries are those appearing in intense reflections. To know the correct point group, the symmetries of weak reflections must be examined. Photograph (j) shows a CBED pattern taken from an area of about 3 nm diameter by tilting the specimen from the incidence along a twofold axis into a direction in which a mirror symmetry is expected to exist. Weak reflection pairs AA' and BB', for instance, show a small breakdown of a mirror symmetry. It is not



clear at the present stage whether this breakdown is inherent in the quasicrystal or is attributed to residual strains of the specimen.



Icosahedral point groups. Quoted from International Tables for Crystallography, vol. A pp.778~779.

### CBED symmetries of icosahedral phases

Point group	Diff. group	BP	WP	DP	$\pm$ DP
235	$5m_R$	$5m$	5	$\left\{ \begin{array}{l} 1 \\ m_2 \end{array} \right.$	$\left\{ \begin{array}{l} 1 \\ m_R \\ 1 \end{array} \right.$
	(Projection) $5m1_R$	$10mm$	$5m$	$\left\{ \begin{array}{l} 2=1_R \\ 2m_v m_2 \end{array} \right.$	$\left\{ \begin{array}{l} 1 \\ m_v 1_R \\ 1 \end{array} \right.$
$m\bar{3}5$	$10_R mm_R$	$10mm$	$5m$	$\left\{ \begin{array}{l} 1 \\ m_2 \\ m_v \end{array} \right.$	$\left\{ \begin{array}{l} 2_R \\ 2_R m_2 \\ 2_R m_v \end{array} \right.$
	(Projection) $10mm1_R$	$10mm$	$10mm$	$\left\{ \begin{array}{l} 2 \\ 2m_v m_2 \end{array} \right.$	$\left\{ \begin{array}{l} 21_R \\ 21_R m_v \end{array} \right.$

**Al<sub>74</sub>Mn<sub>20</sub>Si<sub>6</sub> — Diffraction patterns —**

In the previous pages, we have been concerned with symmetry determination by assuming that a quasicrystal exists. We now return to discuss the diffraction pattern which shows a fivefold symmetry. Notwithstanding a much better ordering, a zig-zag deviation of diffraction spots was still observed in Al<sub>74</sub>Mn<sub>20</sub>Si<sub>6</sub>. The inner disks in the CBED pattern (a) are slightly overlapped to visualize the displacement of diffraction spots. It is clearly seen that the second disk in the direction *h* overlaps that in the direction *k* to a greater extent than the disks in other directions, and that the equivalent disk in the direction *m*, which is perpendicular to the direction midway between the directions *h* and *k*, radially overlaps the outer disk more than in the other directions. Close inspection of the diffraction pattern (b) on page 92, reveals the following facts. All the spots in the directions *m* and *n* line up or show almost no angular deviation. These two directions are not equivalent, because the spots S1-S6 in the direction *n* are situated at different radial positions from the spots S1'-S6' in the direction *m*. The diffraction spots in the other directions show an angular deviation. The deviated positions of the reflections in these directions can be produced by linear combinations of the reflection vectors in the directions *m* and *n*. Therefore, the two fundamental reciprocal lattice vectors can be taken in the directions *m* and *n* for the diffraction pattern (b) as in usual crystals, instead of requiring five fundamental reciprocal lattice vectors.

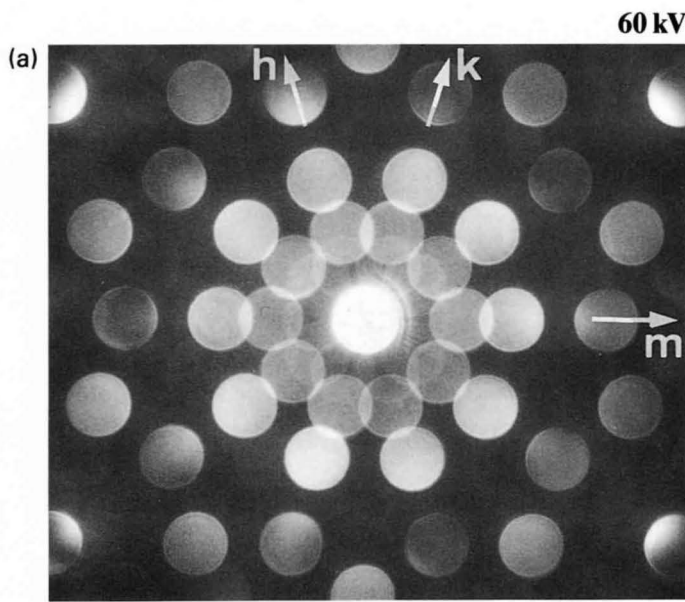
All the positions of the spots in the fundamental direction *n* are reproduced by the Fourier transform of a quasiperiodic array expressed by the equation

$$X_n = n + (1/\varrho)[n/\tau]. \tag{1}$$

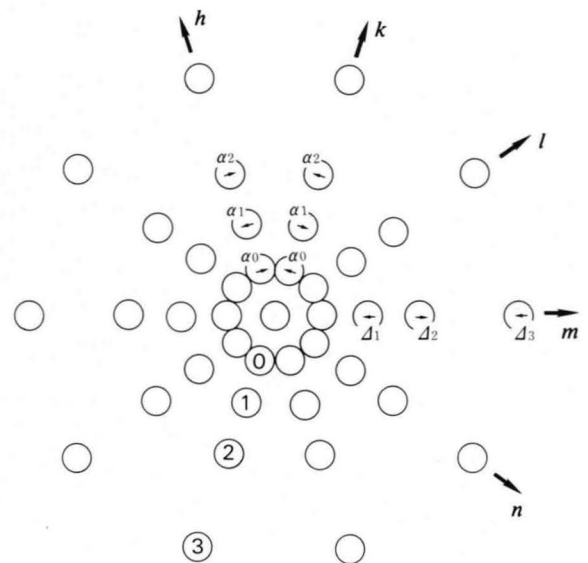
When  $\varrho = \tau = (1 + \sqrt{5})/2$ , the quasi-periodic array LSLLSLSLL... (Fibonacci sequence) is generated, where L and S have relative lengths of  $(1 + \sqrt{5})/2$  and 1, respectively. The value of  $\varrho$  determines the ratio between the lengths L and S, and that of  $\tau$  the sequence of them. The Fourier transform of the array is shown in Fig. (a). The positions of the peaks F1-F3 and S1-S6 well correspond to those of the reflections indicated with the same symbols in Photo (b).

It is noted that the calculated diffraction pattern of Fig.(a) resembles that of a long-period superlattice structure in a binary alloy which consists of an ordered array two kinds of atoms and periodic antiphase domain boundaries [a]. That is, the strong reflections, F0-F3 in Fig.(a), can be regarded as the fundamental reflections of the disordered (averaged) array, and pairs of reflections, (S1,S2), (S3,S4) and (S5,S6), symmetrically situated between the fundamental reflections can be regarded as split superlattice reflections. In fact, the quasi-periodic array expressed by eq.(1) can be created to a good approximation by the introduction of the ordering of two elements (L and S) and periodic antiphase boundaries to the ordered array of L and S, although the "uniform" mixing of two long-period superlattice structures with different periods is needed to reproduce the incommensurate property of the quasilattice [b]. The meaning of the "uniform" mixing and how to produce it can be understood by the projection method [c].

The calculated diffraction pattern of a periodic array



CBED pattern of Al<sub>74</sub>Mn<sub>20</sub>Si<sub>6</sub>. Disks are slightly overlapped.



with a sequence LSLLS is shown in Fig.(b) as an approximation of the diffraction pattern of Fig.(a). These two patterns show very similar peak positions and intensities, except for very weak peaks. This indicates that the diffraction patterns obtained from the present alloy may be interpreted by a periodic array.

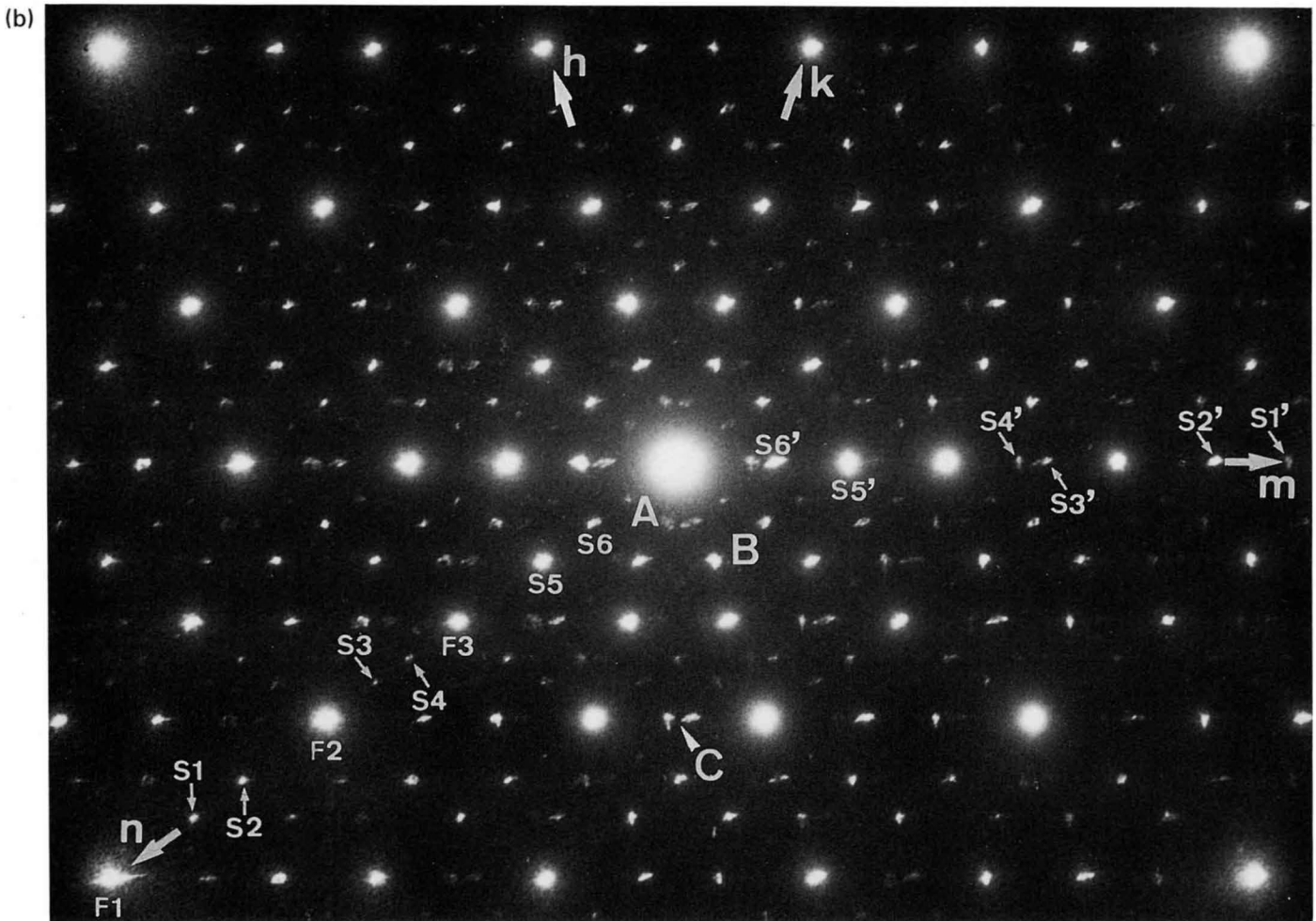
In contrast to the direction  $n$ , the coupled shifts of the pairs of split superlattice reflections are seen along the fundamental direction  $m$  in Photo (b). The shifts are shown schematically by arrows in the calculated pattern of Fig.(a). This suggests that there exists a change in the period of the antiphase boundaries in the language of the long-period superlattice in binary alloys. The sense of the shifts has been reproduced by a periodic array of LLS, which can not be created by eq.(1), as shown in Fig.(c). (It is worth while to note that the opposite-sense shift to the present one is produced by a periodic array of LS. (see page 104))

As a result, the experimental diffraction pattern of the present alloy (Photo (b)) might be explained by such a crystal lattice that has tentative periodic arrays of LSLLS and LLS in the directions  $n$  and  $m$ , respectively.

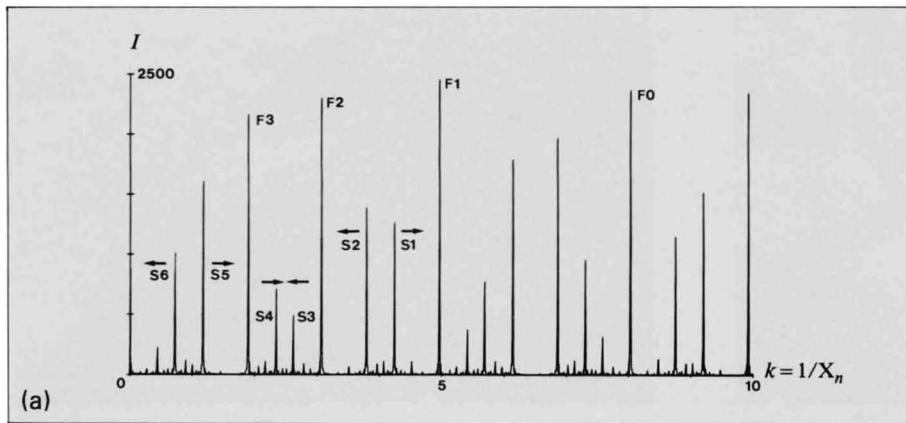
The specimens of  $Al_4Mn$  and  $Al_{74}Mn_{20}Si_6$  were supplied by Dr. A. Inoue and Prof. T. Masumoto of the Research Institute for Iron, Steel and Other Metals, Tohoku University.

### References

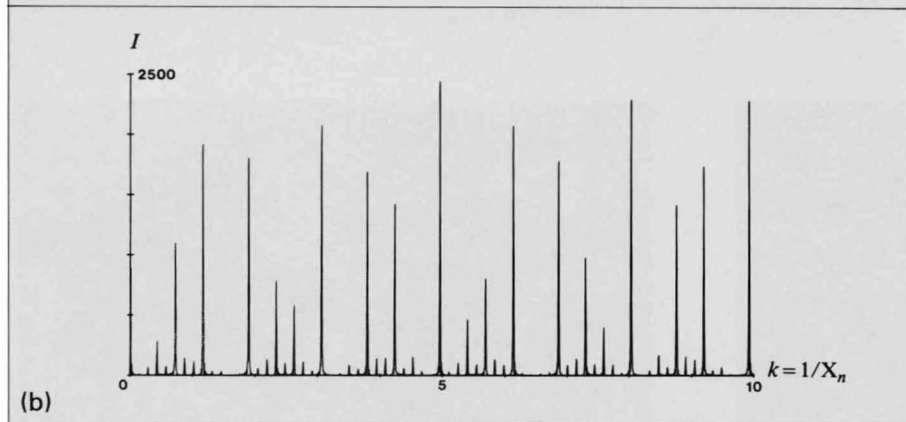
- [a] C.H. Johansson and J.O. Linde: *Ann. Physik*, **25** (1936) 1.
- [b] K. Fujiwara: *J. Phys. Soc. Jpn.*, **12** (1957) 7.
- [c] V. Elser: *Phys. Rev.*, **B32** (1985) 4892.



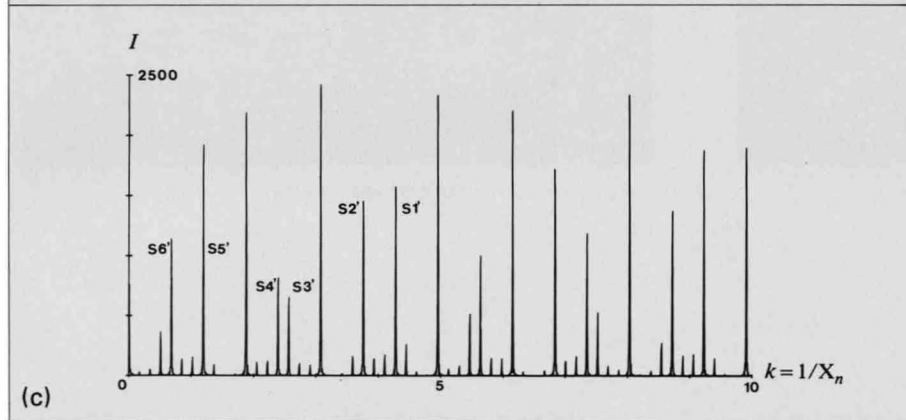
Diffraction pattern of  $Al_{74}Mn_{20}Si_6$



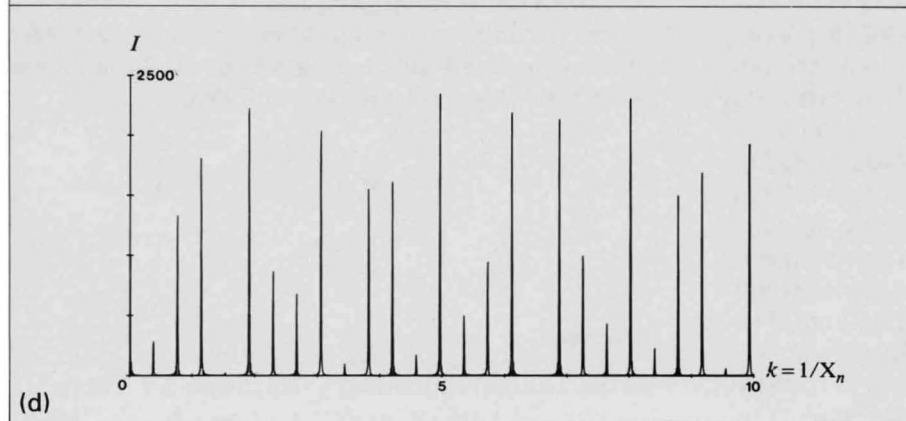
Quasi-periodic array  
 $X_n = n + (1/\varrho)[n/\tau]$   
 $\varrho = \tau = (1 + \sqrt{5})/2$



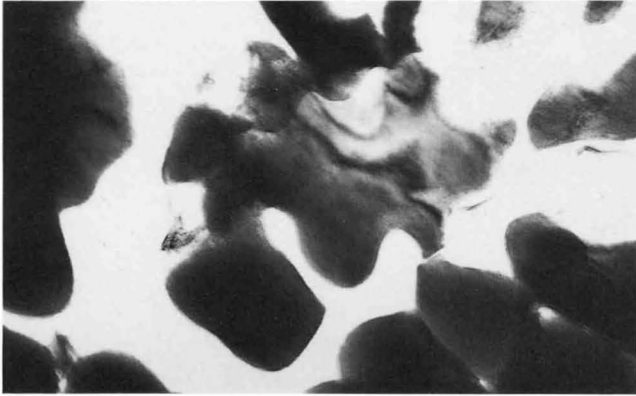
Periodic array of LSLLS



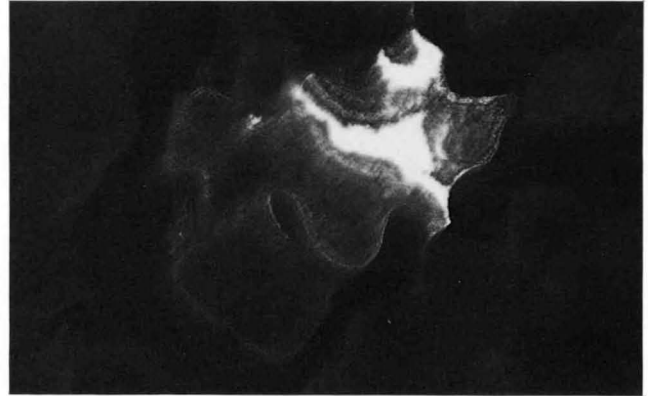
Periodic array of LLLS



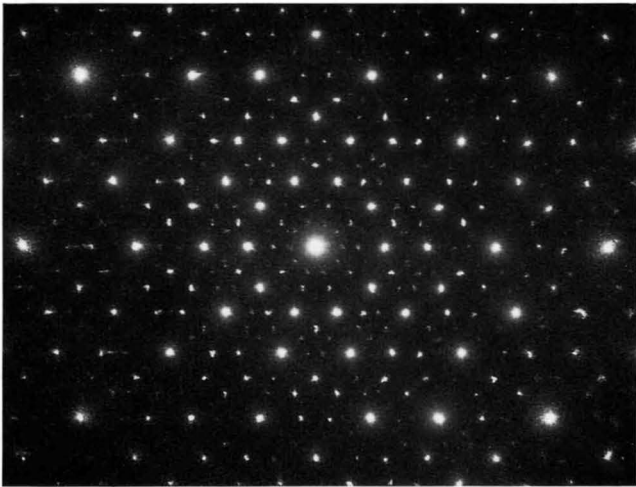
Periodic array of LS



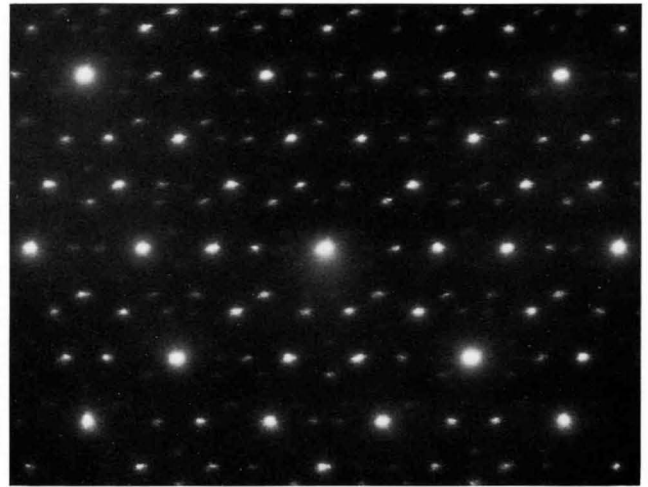
(a) Bright-field image.



(b) Dark-field image.



(c) Diffraction pattern of high quality.



(d) Diffraction pattern of low quality.

Yamane *et al.* succeeded in growing a single-icosahedral-phase alloy of  $\text{Al}_{68}\text{Mn}_{20}\text{Ru}_6\text{Si}_6$ . They reported that X-ray diffraction profiles obtained from the alloy were sharper than those from other similar alloys. We have examined the alloy using CBED and small-area-parallel-beam electron diffraction. A small-area-parallel-beam electron diffraction pattern (c), which was taken from a 110 nm diameter area of Photo (a), shows very little zig-zag deviation of diffraction spots, although a low quality specimen area gave a pattern (d) with a large zig-zag deviation and no spots corresponding to the spacing 2.27 nm. The average degree of order of the phase was found to be better than that of  $\text{Al}_{74}\text{Mn}_{20}\text{Si}_6$ . Photographs (e) to (j) show three pairs of CBED patterns. Their quality appears to be a little inferior to that of the corresponding CBED pat-

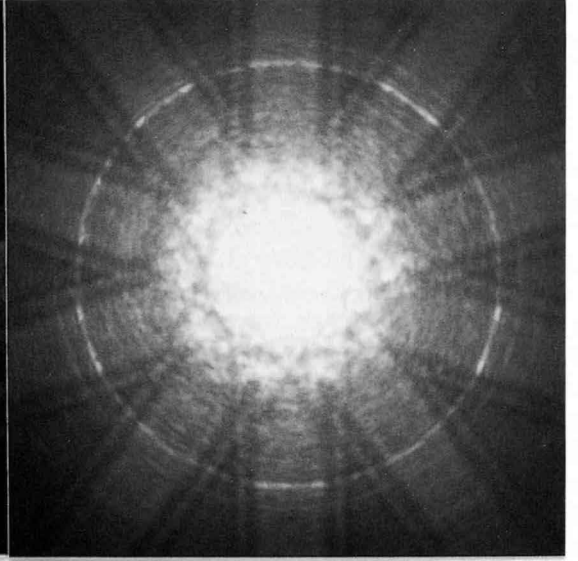
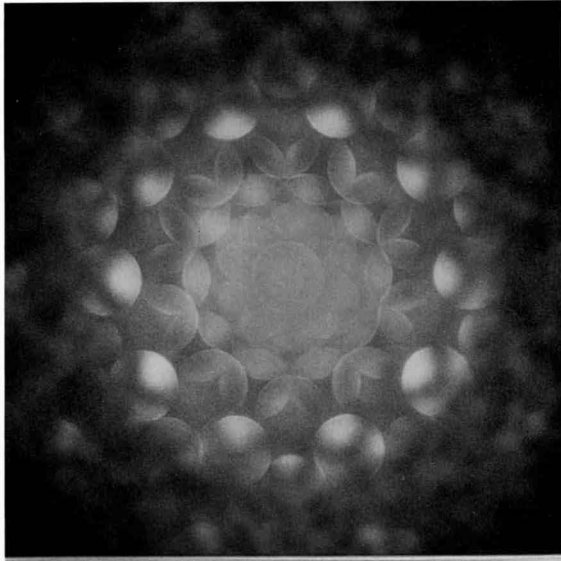
terns obtained from  $\text{Al}_{74}\text{Mn}_{20}\text{Si}_6$ .

The specimens were supplied by Dr. K. Kimura, Mr. H. Yamane and Prof. S. Takeuchi of the Institute for Solid State Physics, University of Tokyo.

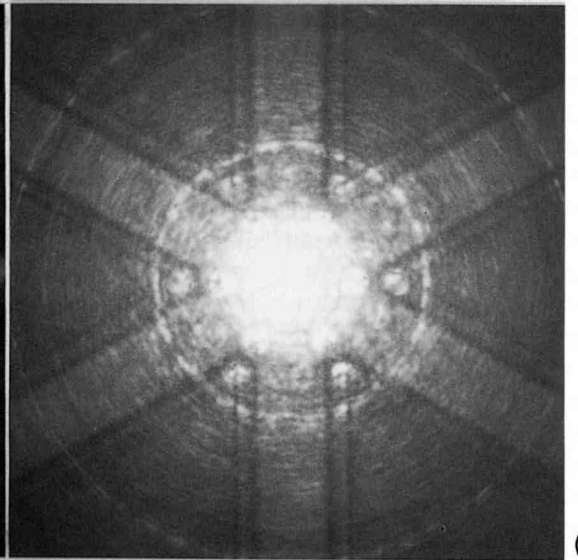
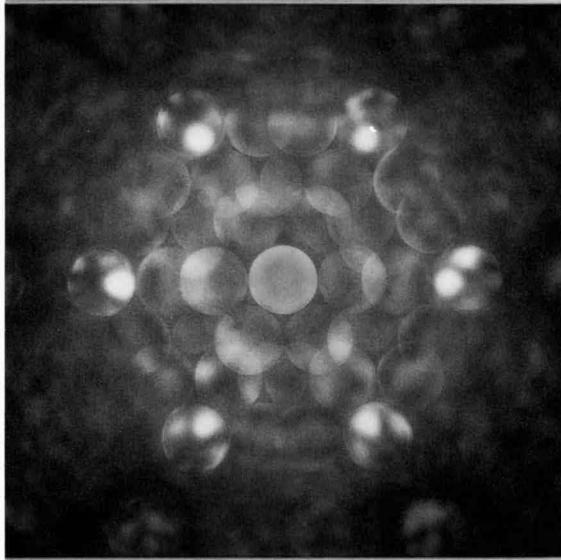
#### Reference

- [a] H. Yamane, K. Kimura, T. Shibuya and S. Takeuchi: Proc. of Inter. Workshop on Quasicrystals, Beijing, 1987

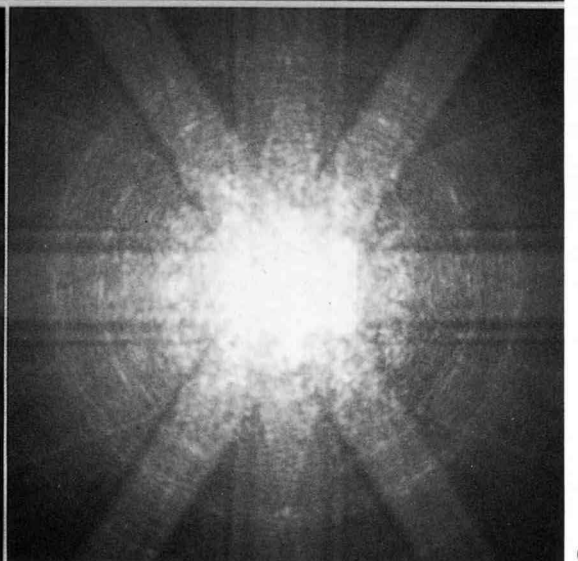
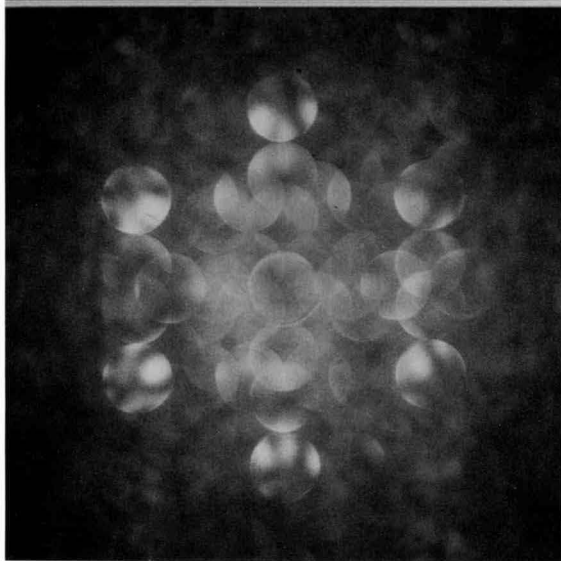
Fivefold axis



Threefold axis



Twofold axis



## Al<sub>65</sub>Cu<sub>20</sub>Fe<sub>15</sub>

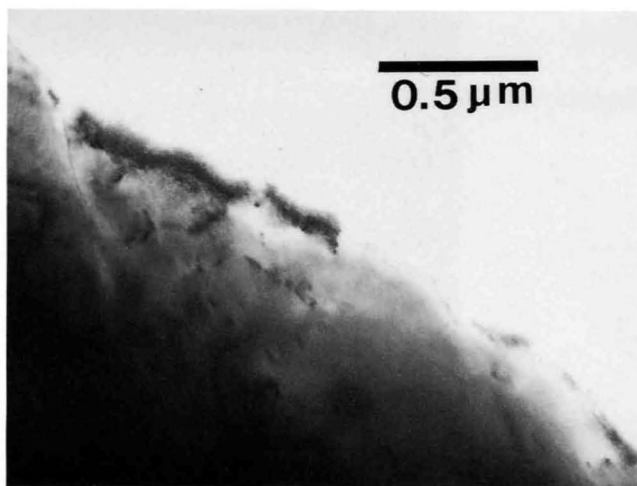
Tsai *et al.* have produced an alloy of Al<sub>65</sub>Cu<sub>20</sub>Fe<sub>15</sub> with a thermally stable icosahedral phase. They reported that the phase has a grain size as large as about 10 μm and is stable without phase transition up to the melting point.

Electron microscope images (Photos (a) and (b)) of Al<sub>65</sub>Cu<sub>20</sub>Fe<sub>15</sub> indicate that this alloy has the largest grain size among the quasicrystals examined so far. Almost all the specimen areas of this alloy produced a smaller zig-zag deviation in small-area-parallel-beam electron diffraction patterns (Photos (c) to (e)) than Al<sub>74</sub>Mn<sub>20</sub>Si<sub>6</sub>.

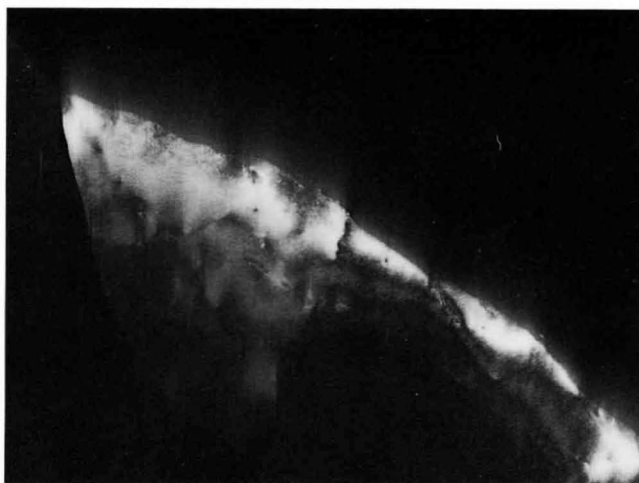
ZOLZ CBED patterns showed nearly perfect symmetries of 10 $m$  (f), 6 $m$  (h) and 2 $m$  (j) at incidences along the fivefold, threefold and twofold axes, respectively, in contrast to slightly faulted symmetries obtained from other icosahedral alloys. The intensity distributions of HOLZ rings (g), (i) and (k) of this alloy are different from those of Al<sub>74</sub>Mn<sub>20</sub>Si<sub>6</sub>, presumably indicating the difference between their structures. Owing to the presence of large grains, thickness changes of CBED patterns (Photos (l) and (m)) were observed. This alloy of Al<sub>65</sub>Cu<sub>20</sub>Fe<sub>15</sub> has the best qualified icosahedral phase among the alloys examined by us.

When a slightly convergent beam is used, diffraction patterns can be obtained from intermediate sized illuminated areas (approx. 20 nm in diameter) between areas needed for small-area-parallel-beam diffraction patterns (approx. 110 nm in diameter) and for CBED patterns (less than 5 nm in diameter). In Photos (n) to (p), HOLZ rings are more clearly seen and deviations of weak reflections from symmetries 5 $m$ , 3 $m$  and 2 $m$  can be seen, whereas HOLZ rings are not easy to see in small-area-parallel-beam diffraction patterns (Photos (c) to (e)) and weak reflections can not be seen in CBED patterns (Photos (f) to (m)). Diffraction spots including HOLZ reflections in Photo (n) shows a very good symmetry 5 $m$ . Weak reflections in Photos (o) and (p), however, show deviations from symmetries 3 $m$  and 2 $m$ , respectively. The details of the deviations are under study. This quasicrystal was found to be still insufficiently uniform, because the deviations easily changed when an illuminated area was shifted by about 50 nm.

The specimens were supplied by Dr. A. Inoue and Prof. T. Masumoto of the Research Institute for Iron, Steel and Other Metals, Tohoku University.



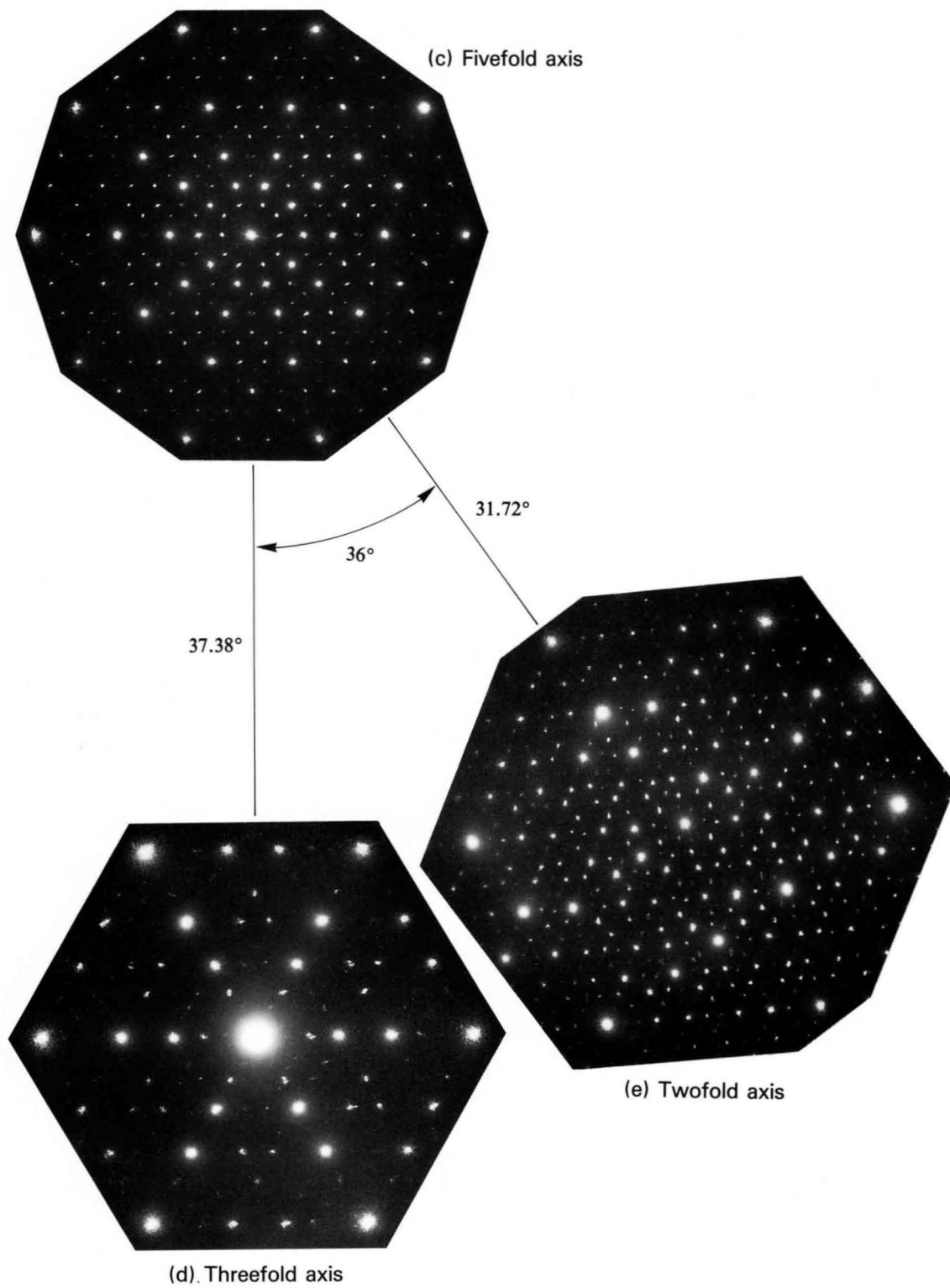
(a) Bright-field image



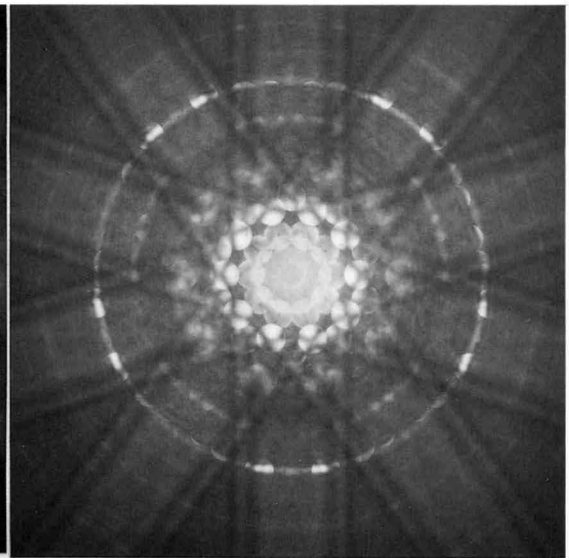
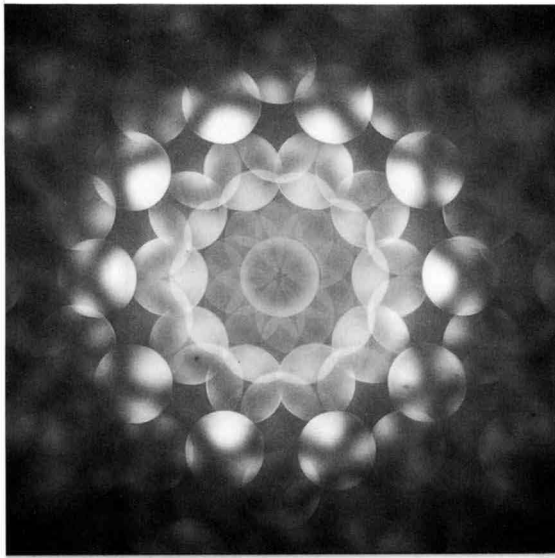
(b) Dark-field image

## Reference

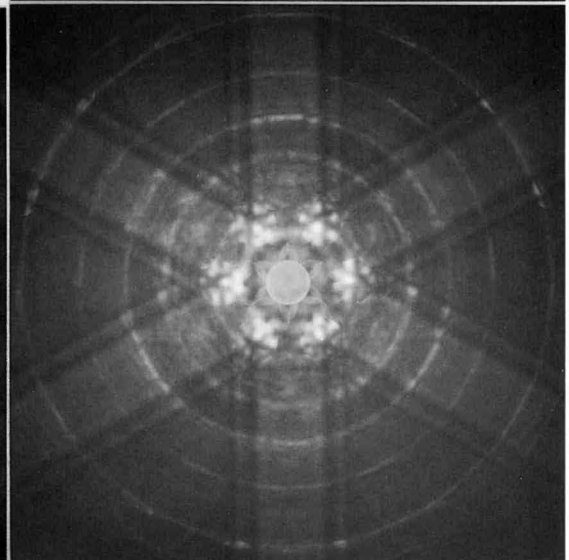
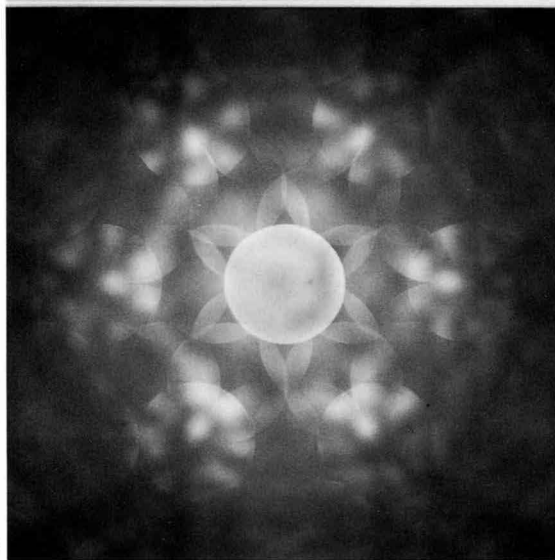
- [a] A.P. Tsai, A. Inoue and T. Masumoto: *Jpn. J. Appl. Phys. Lett.*, **26** (1987) L1505.



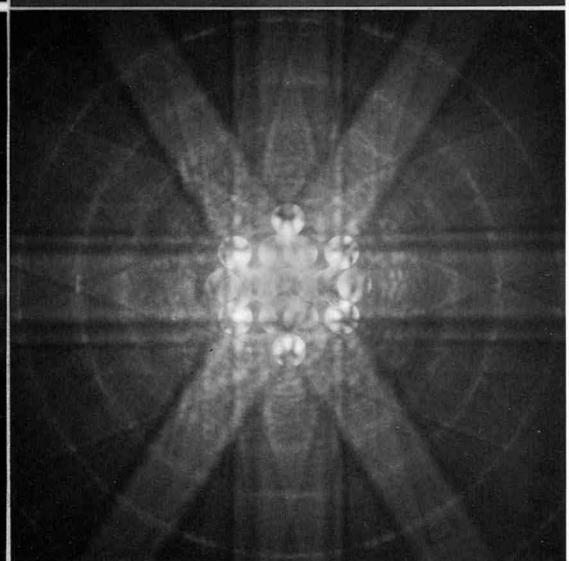
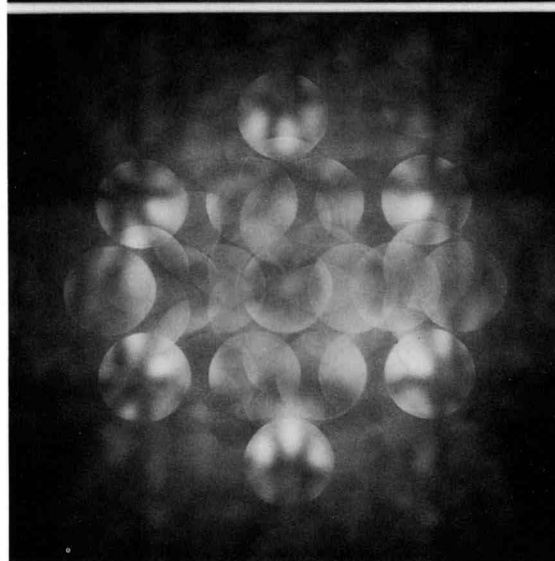
Fivefold axis



Threefold axis



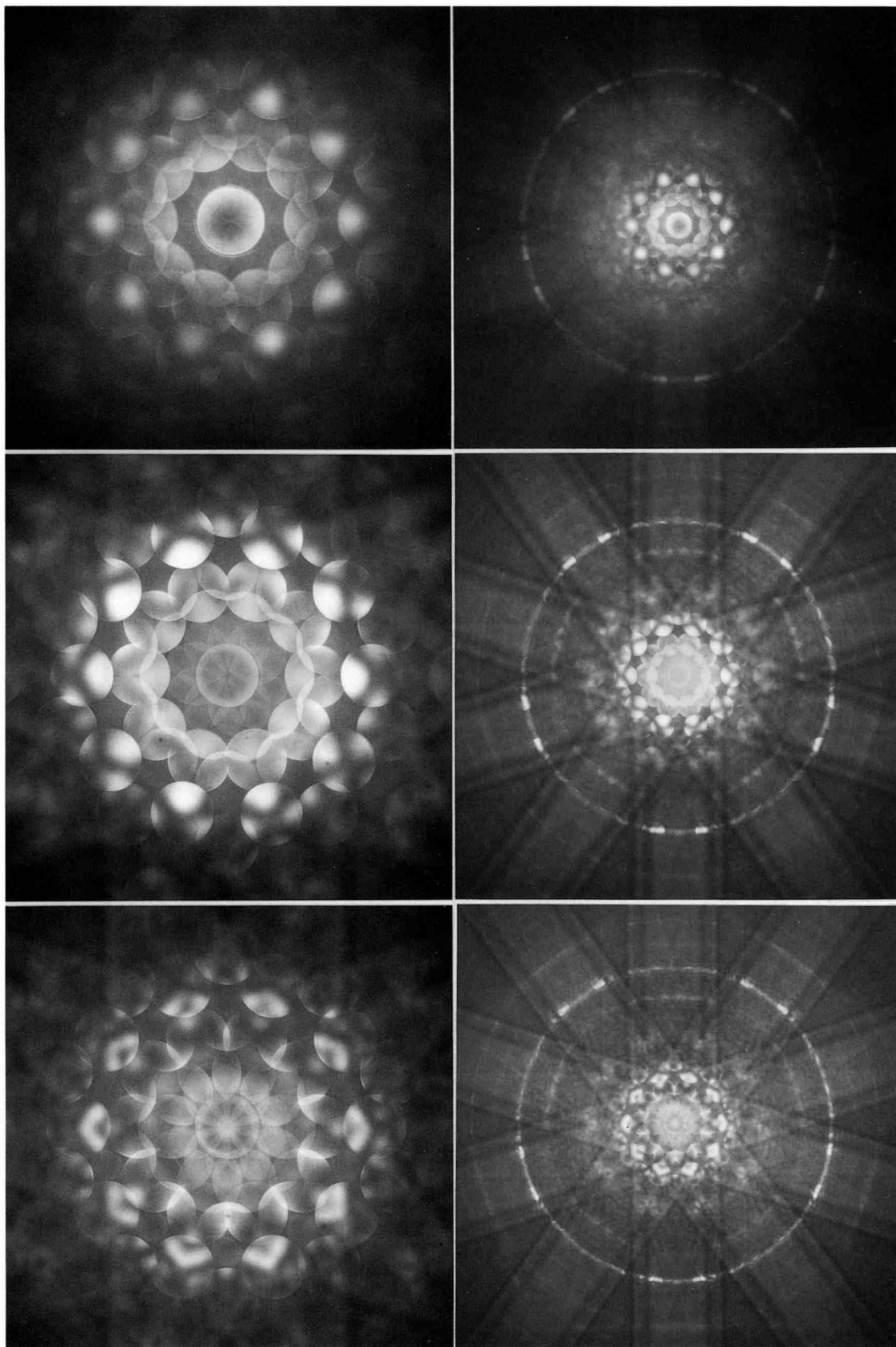
Twofold axis



Thickness dependence of CBED pattern (fivefold axis)

60 kV

(I)

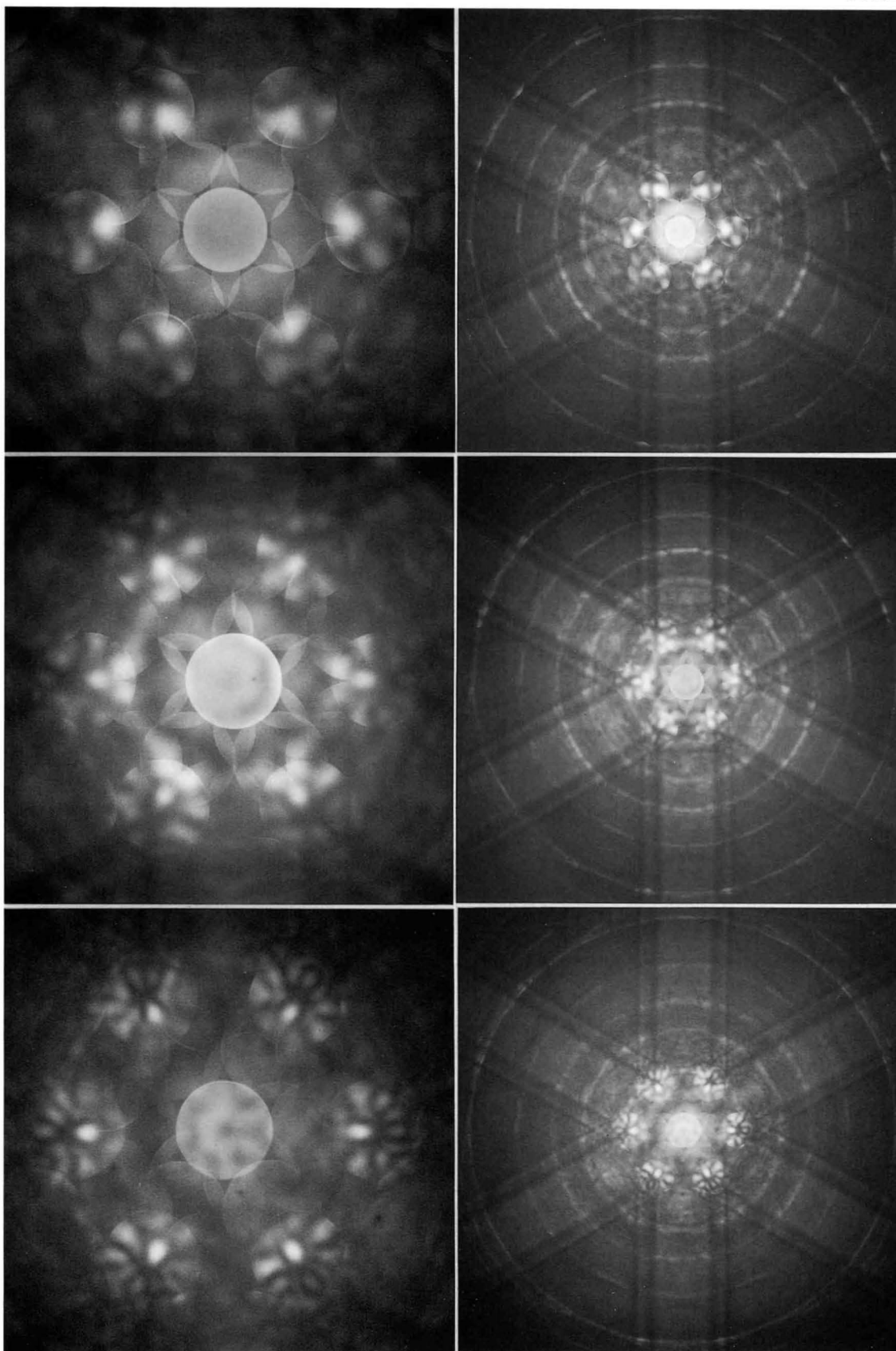


$\text{Al}_{65}\text{Cu}_{20}\text{Fe}_{15}$

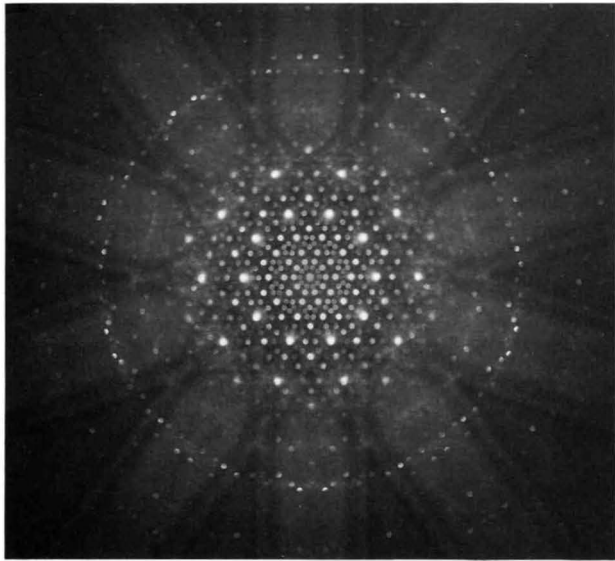
Thickness dependence of CBED pattern (threefold axis)

60 kV

(m)

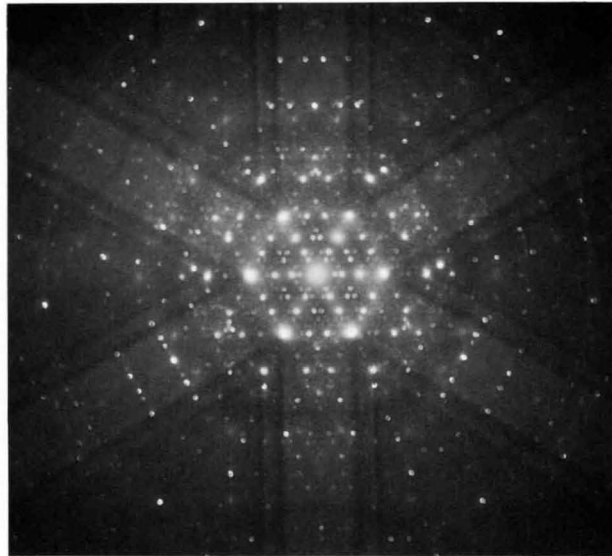


**Diffraction patterns taken with slightly convergent beam**

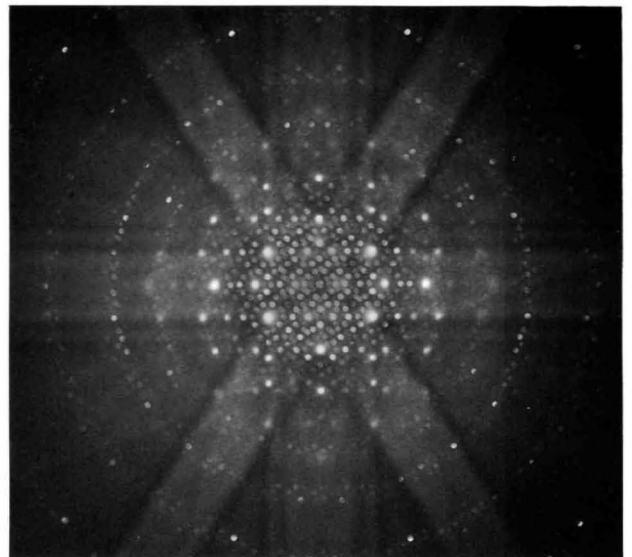


60 kV

(n) Fivefold axis



(o) Threefold axis

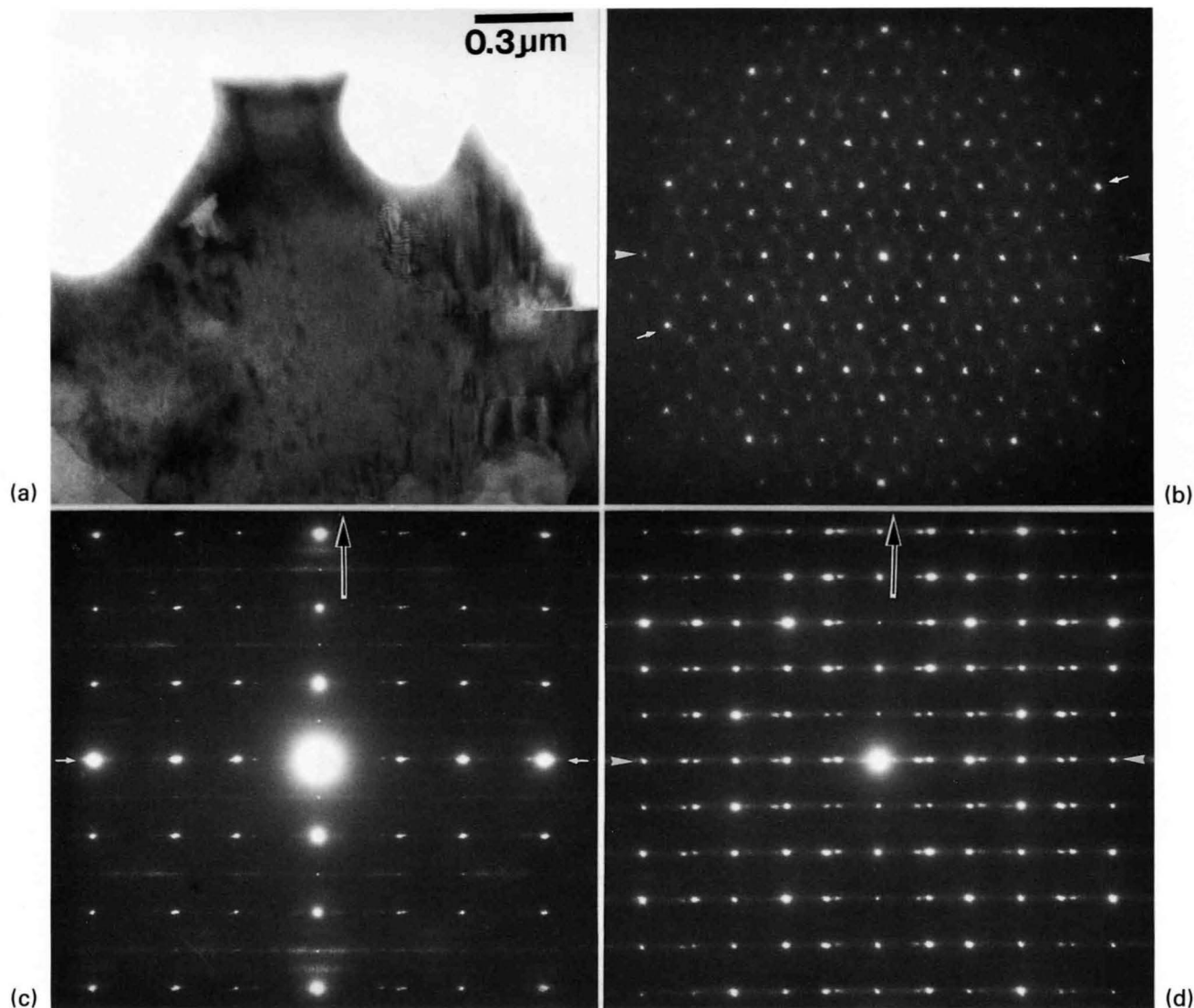


(p) Twofold axis

# Decagonal Phases

Al-Mn system

60 kV



A decagonal phase found in an Al-Mn alloy has a tenfold rotation axis. The phase has a translational symmetry parallel to the tenfold axis and a quasi-periodic long-range structural order perpendicular to the axis. Two space groups,  $P10_5/m$  and  $P10_5/mmc$ , have been proposed by Bendersky [a] and Yamamoto [b], respectively.

The diffraction pattern (b) was taken at an incidence along the tenfold axis. The diffraction patterns (c) and (d) were taken at two incidences perpendicular to the tenfold axis. The diffraction spots are periodic in the direction of the tenfold axis indicated by the black arrows. The arrays of diffraction spots indicated by two different white arrows in the two patterns (c) and (d) correspond to those indicated by the same arrows in the pattern (b). The spots are seen to be quasi-periodic along these arrays. Three pairs of CBED patterns—(e) & (f), (g) & (h) and (i) & (j)—were taken at incidences for the diffraction patterns (b), (c) and (d), respectively. The symmetries of the patterns are writ-

ten beside the photographs. A tenfold axis and a mirror plane perpendicular to the axis are clearly seen. Owing to the low quality of the specimen, we could not confirm the existence of mirror planes parallel to the tenfold axis. As a result, the point group of this phase was found to be  $10/m$  or  $10/mmm$ . Dynamical extinction was not observed in the CBED patterns.

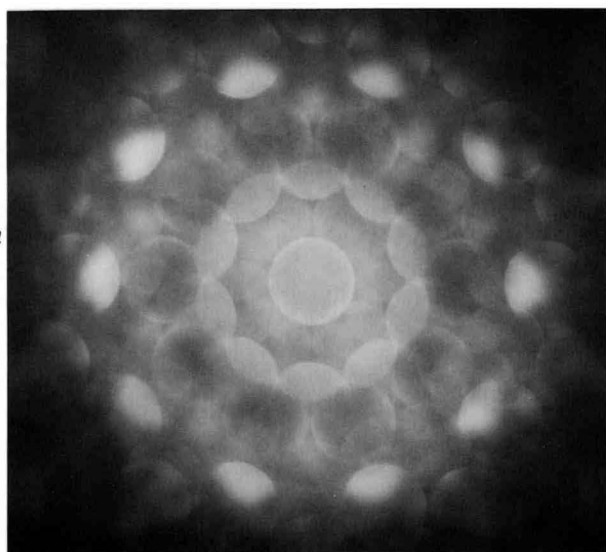
The specimens were supplied by Dr. A. Inoue and Prof. T. Masumoto of the Research Institute of Iron, Steel and Other Metals, Tohoku University.

## References

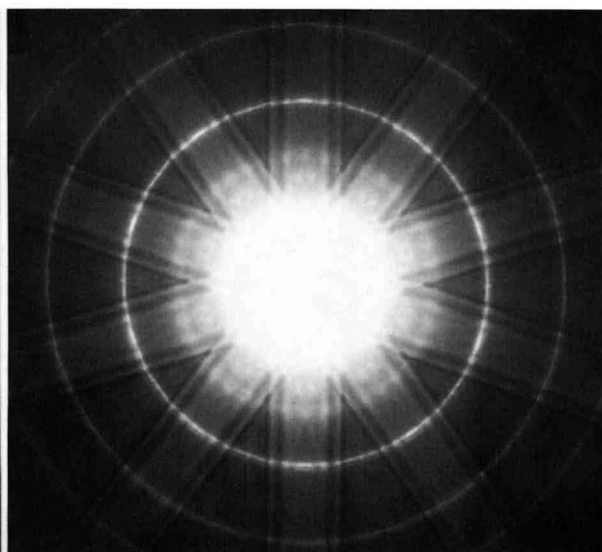
- [a] L. Bendersky: *J. de Physique*, **47** (1986) C3-457.
- [b] A. Yamamoto and K.N. Ishihara: *Acta Cryst.*, in the press.

60 kV

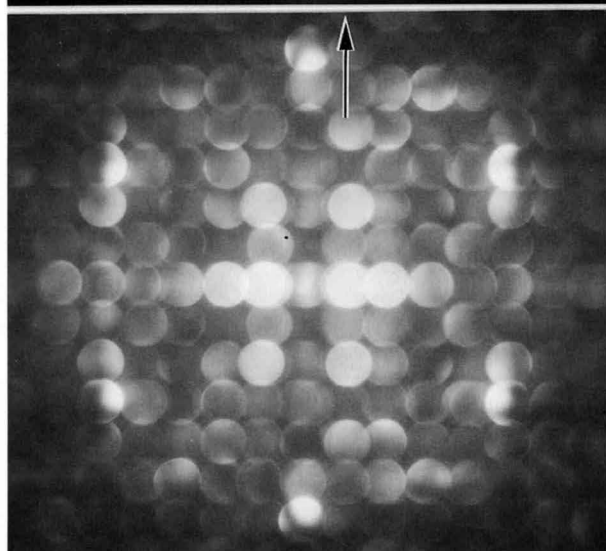
10mm  
or  
10



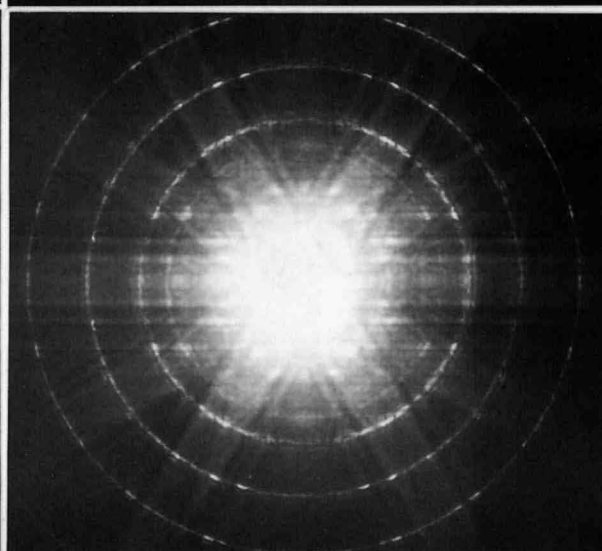
10mm  
or  
10



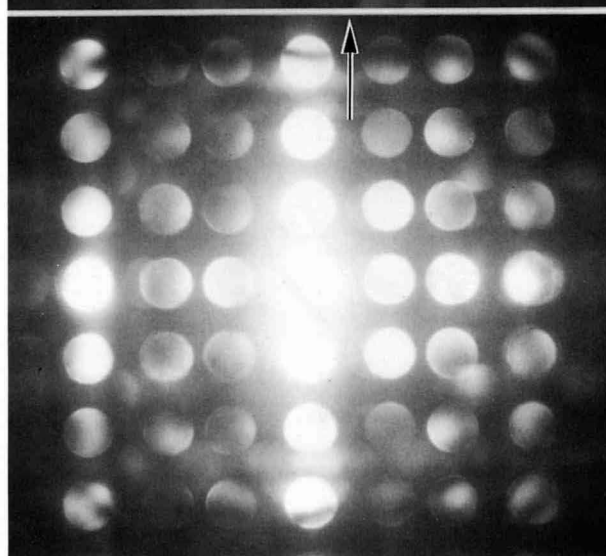
2mm  
or  
m



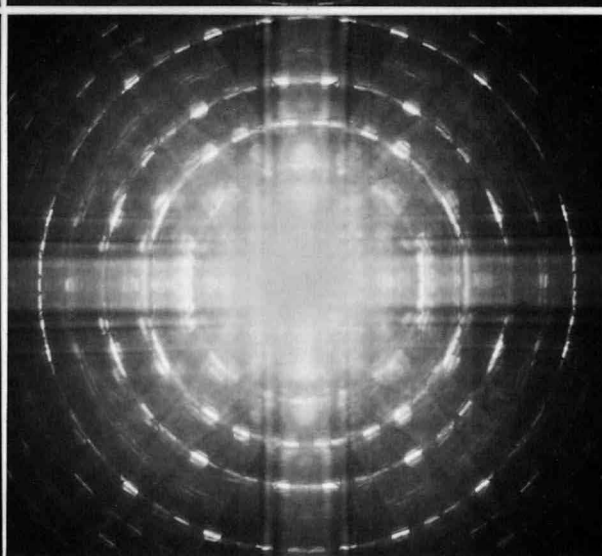
2mm  
or  
m

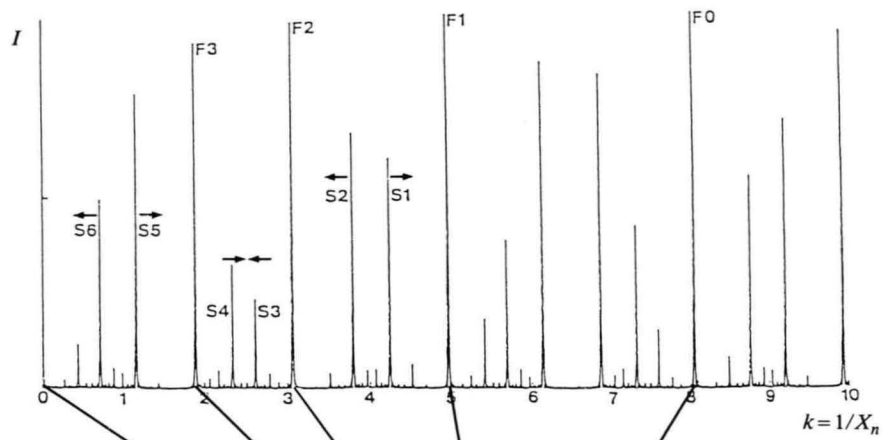


m

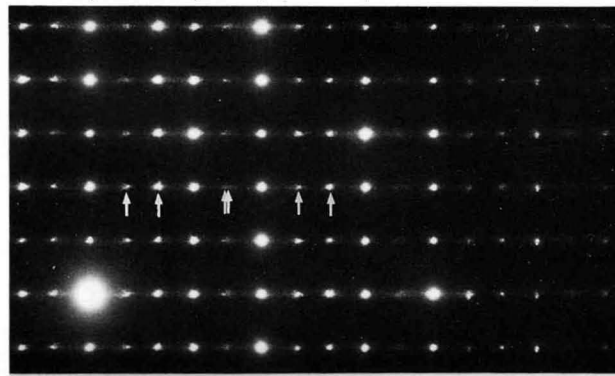


2mm  
or  
m

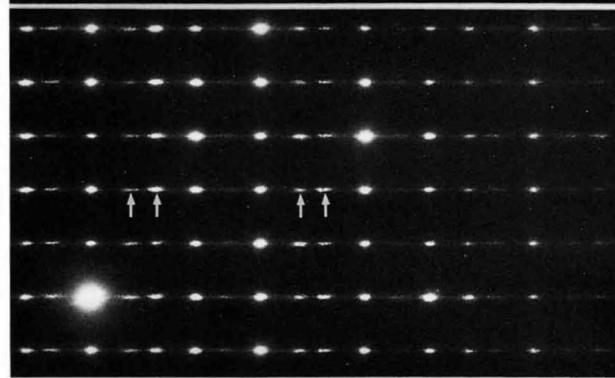




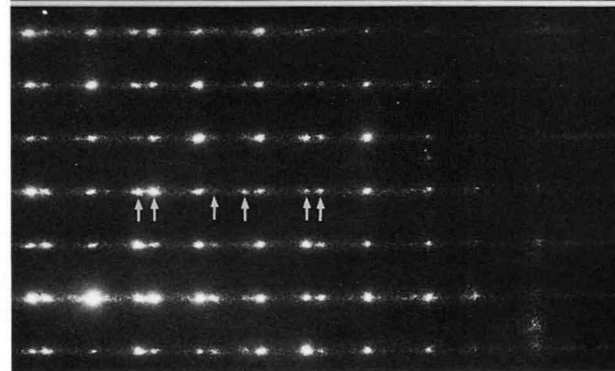
Quasi-periodic array  
 $X_n = n + (1/q)[n/\tau]$   
 $q = \tau = (1 + \sqrt{5})/2$



(k)



(l)



(m)

Three diffraction patterns, (k), (l) and (m), were taken from different specimen areas at the same incidence as that of Photo (c). Diffraction spots indicated by arrows in Photos (k) and (m) show deviations from the positions expected from the ideal quasi-periodic array. The positions of the spots in Photo (l) were well explained by the Fibonacci sequence (eq. (1) on page 91). The pairs of neighbouring spots indicated by arrows in (k) are displaced from the ideal positions to the sense indicated by the arrows in the above diagram. The sense of this displacement is the same as that already described in the section of the icosahedral phase of  $Al_{74}Mn_{20}Si_6$ . The pairs of neighbouring spots indicated by arrows in the pattern (m) are displaced from the ideal positions in the sense opposite to that in the pattern (k) (compare with Fig. (d) on page 93). These results show that the specimens did not yet form a uniform quasicrystal.

# *Computer Simulations*

Computer simulations of CBED patterns were carried out by the usual matrix method. In our computations HOLZ reflections were taken into account automatically when their excitation errors became smaller than a given value. By considering the symmetry of a pattern, the pattern of a necessary minimum angular area was calculated and was extended to the other areas by symmetry operation. The anomalous absorption effect was taken into account by two ways. One is to calculate the imaginary parts of eigenvalues using the perturbation method and another is to evaluate the complex eigenvalues of the matrix which has Fourier coefficients of the absorption potential. It was found that the perturbation method worked good for obtaining the intensity profiles of reflections in a HOLZ ring, but sometimes showed an insufficient accuracy in obtaining the intensities of HOLZ lines appearing in ZOLZ reflections.

The computer used was an NEC-SX-1. Output data was transferred to a personal computer of NEC-9801, and CBED patterns were printed out with 17 grey levels using a laser printer of Canon LBP-B406. The intensities were modified by an appropriate gamma curve when necessary. For the patterns consisting of only ZOLZ reflections computation time at the NEC-SX-1 was saved by applying the Aitken-Neville interpolation method to the patterns at the NEC-9801. To reproduce HOLZ lines, one pixel in a pattern must be taken about  $1 \times 10^{-4}$  rad.

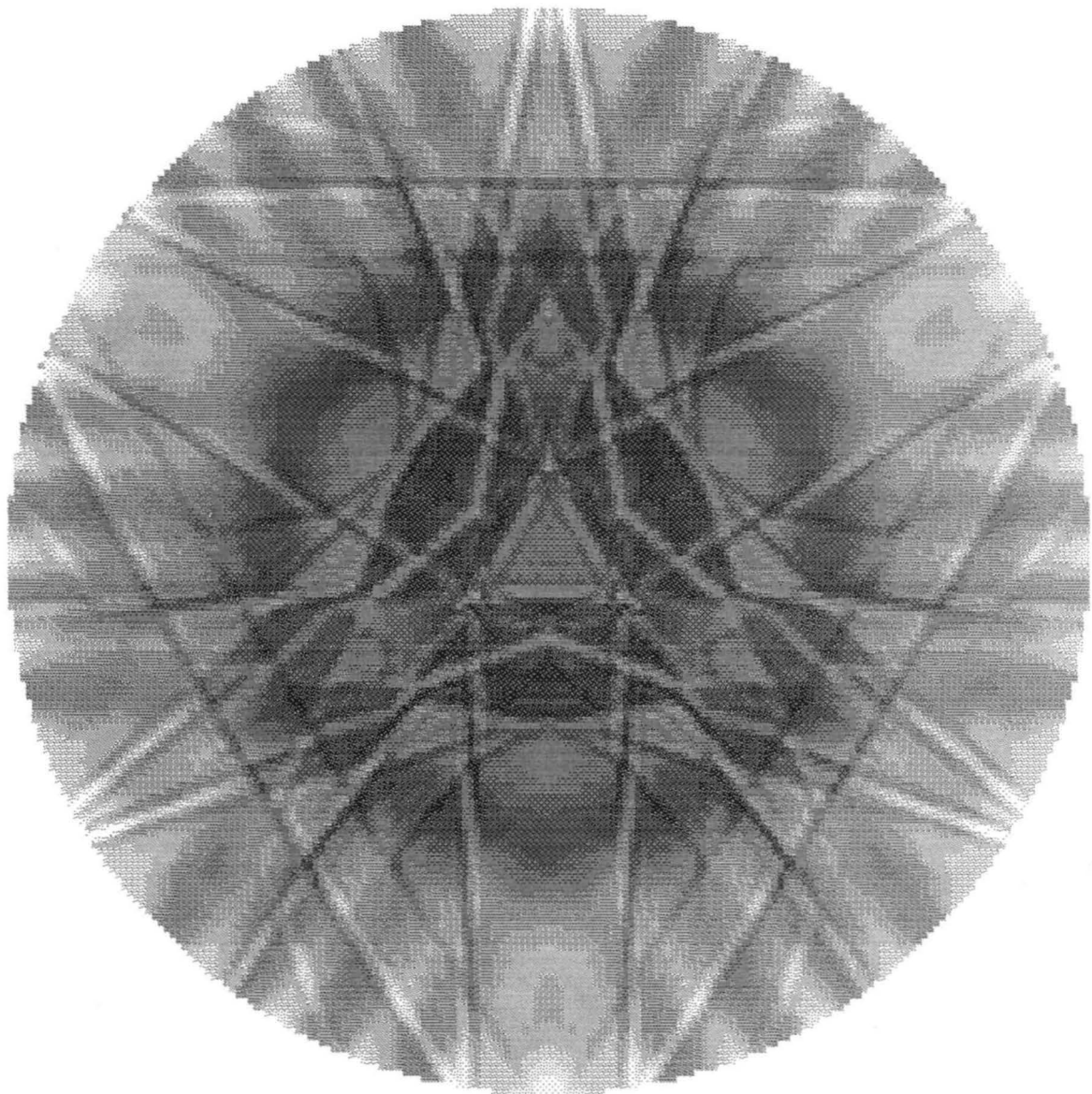
*Si*

**[111] Bright-Field Pattern**

**19 ZOLZ and 11 HOLZ beams, 100kV, thickness 156.8 nm**

Three bright-field patterns were computed for different Debye-Waller factors of 0.0, 0.3 and 0.45. Appreciable differences are seen.

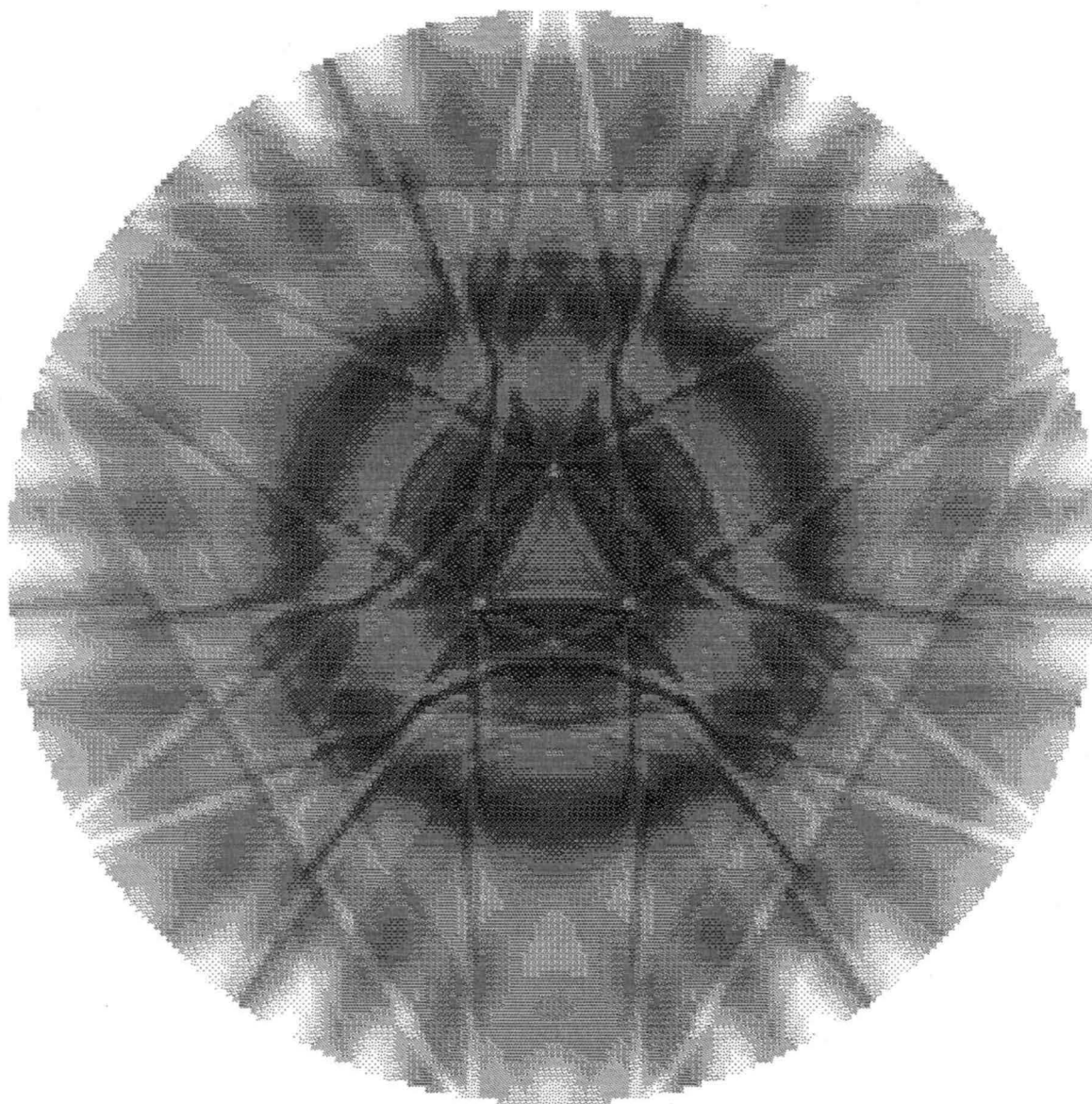
(a) Debye-Waller factor 0.0



181 \* 181 pixels  
type 3 enhancement curve / gamma-coef. = .5

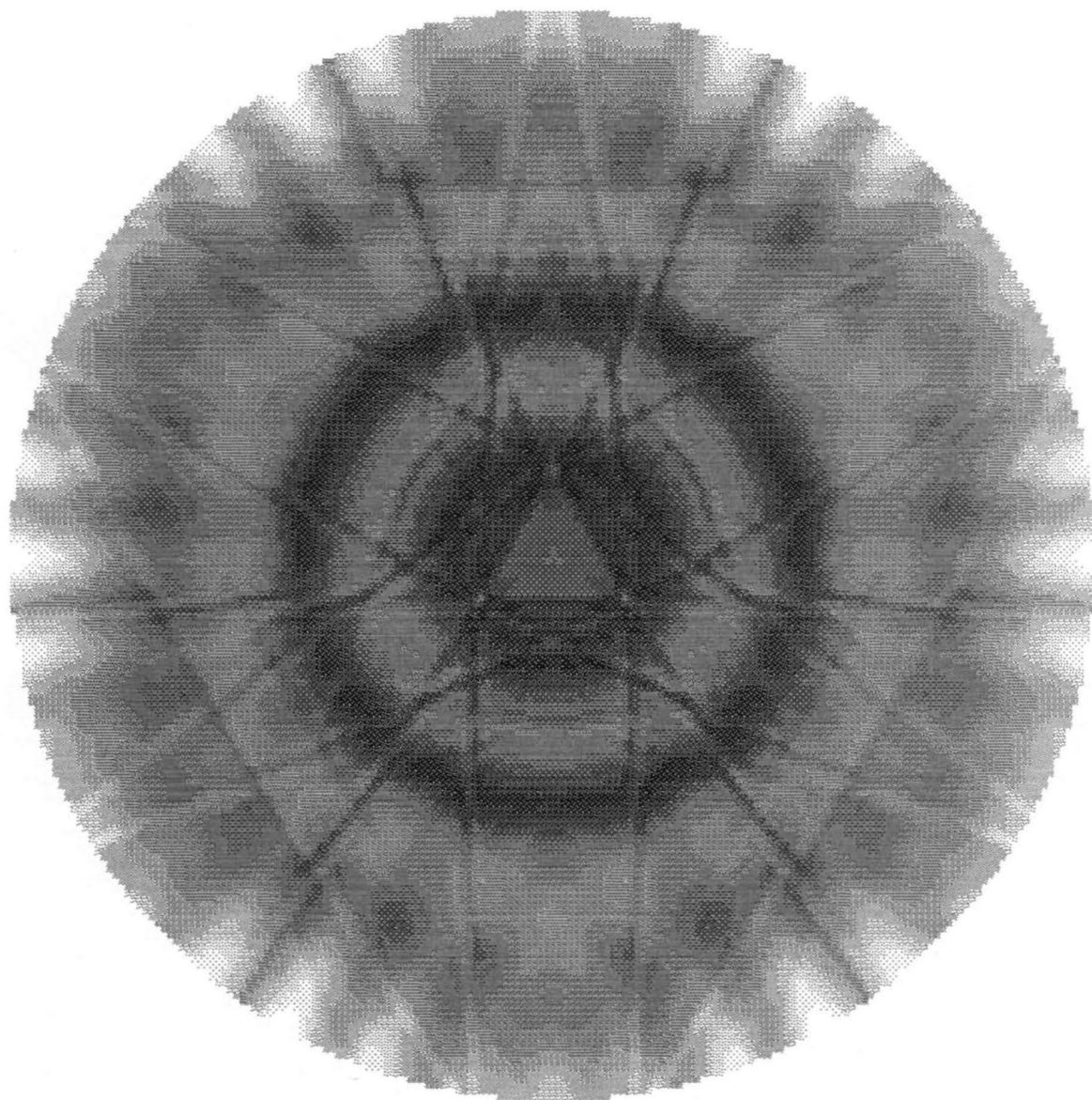
19 ZOLZ and 11 HOLZ beams, 100kV, thickness 156.8 nm

(b) Debye-Waller factor 0.3



181 \* 181 pixels  
type 3 enhancement curve / gamma-coef. = .5

(c) Debye-Waller factor 0.45

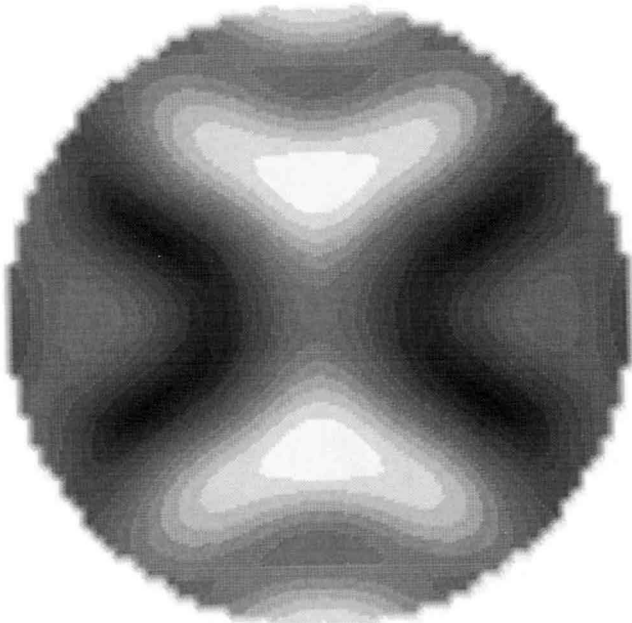


181 \* 181 pixels  
type 3 enhancement curve / gamma-coef. = .5

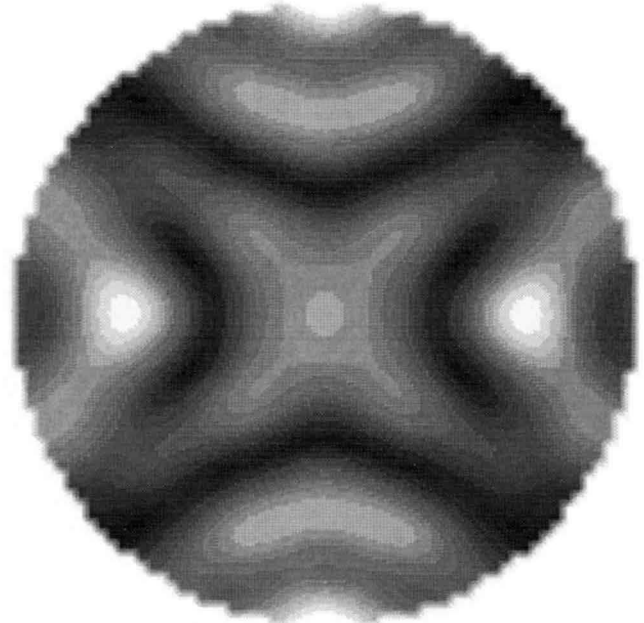
## [110] Bright-Field Pattern

### 23 ZOLZ beams, 100 kV

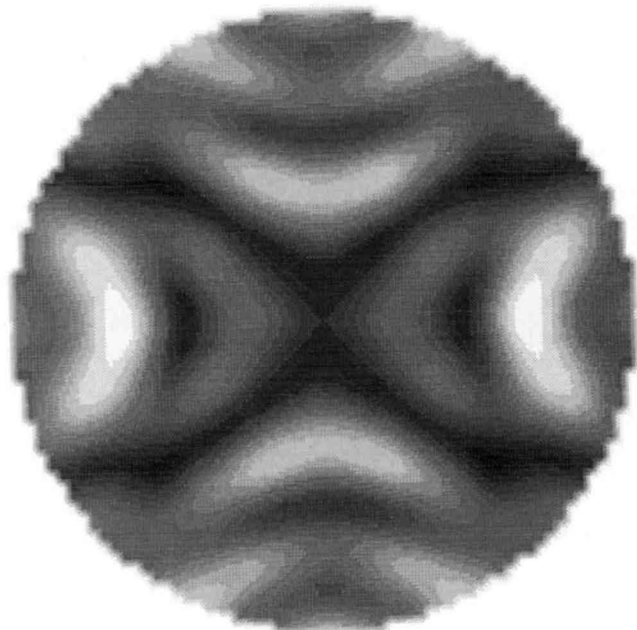
The bright-field patterns were computed for four different thicknesses at 100 kV. The patterns have no HOLZ lines.



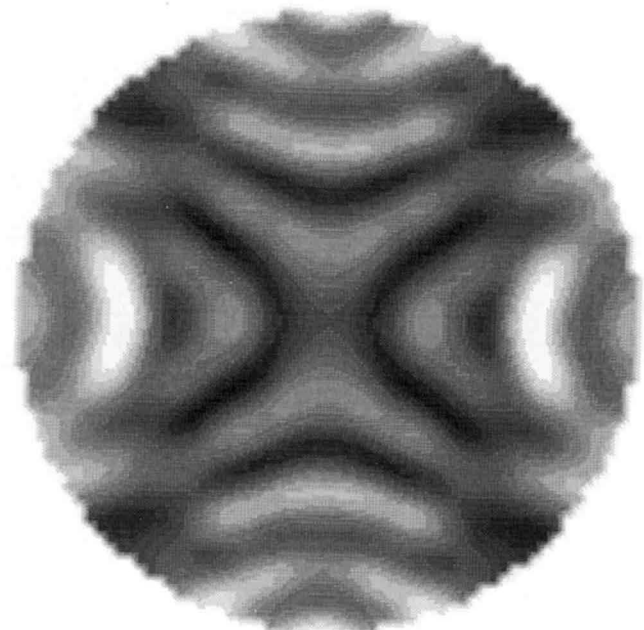
76.8 nm



115.2 nm



153.6 nm



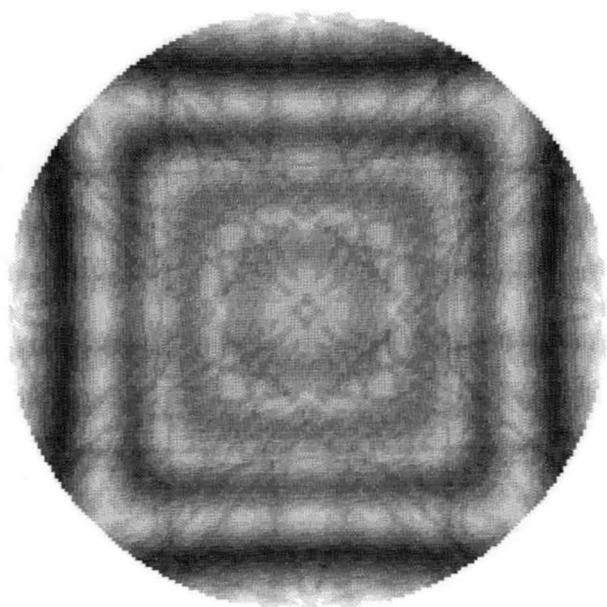
192.0 nm

original(before magnifying): 61 \* 61 pixels  
magnified 3 times / 1 order interpolation  
type 3 enhancement curve / gamma-coef. = .5

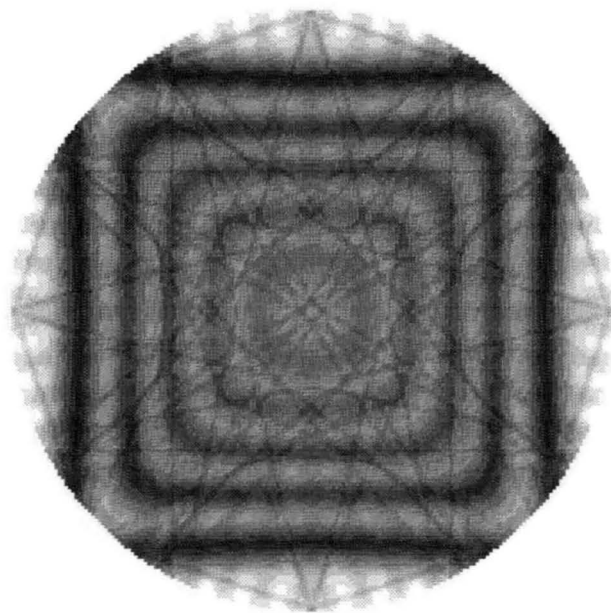
**[001] Bright-Field Pattern**

**21 ZOLZ and 26 HOLZ beams, 40kV, Debye-Waller factor 0.45**

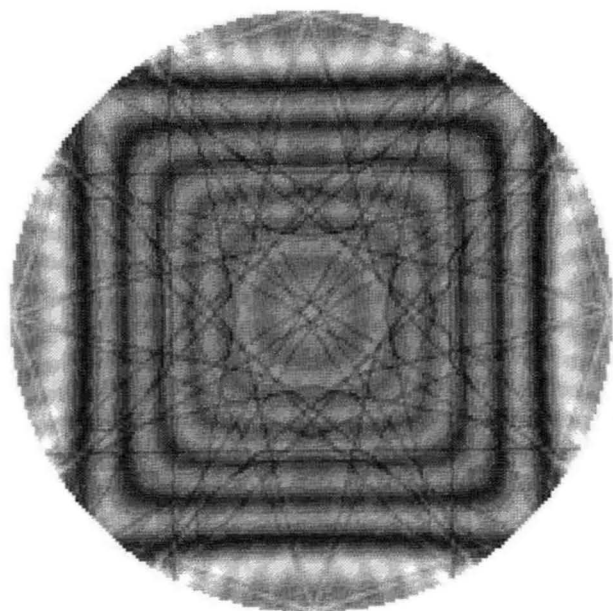
The bright-field patterns were calculated for four different thicknesses at a low accelerating voltage of 40 kV to clearly see HOLZ lines.



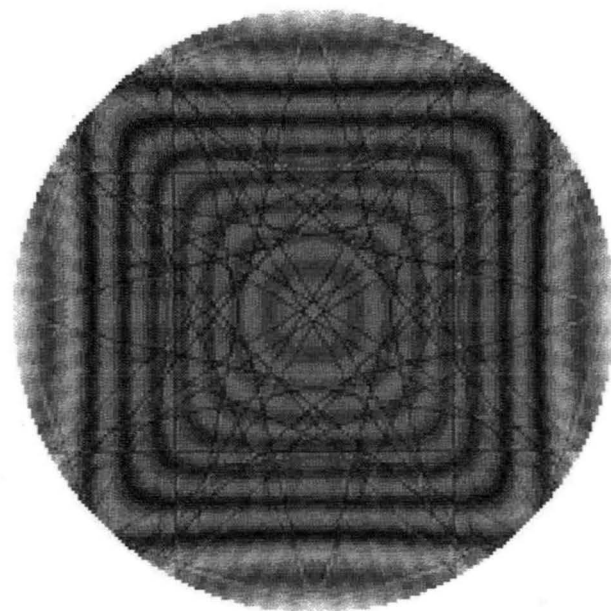
**81.5 nm**



**108.0 nm**



**135.8 nm**



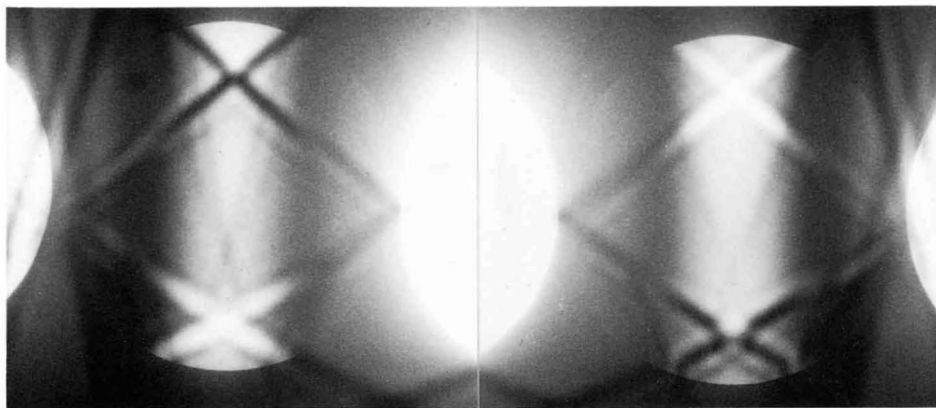
**163.0 nm**

181 \* 181 pixels  
type 3 enhancement curve / gamma-coef. = .5

# GaAs

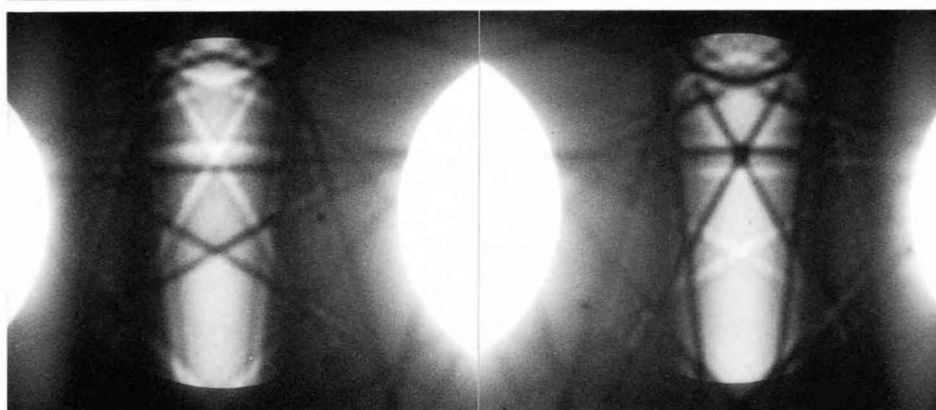
100 kV

[19 2 0]



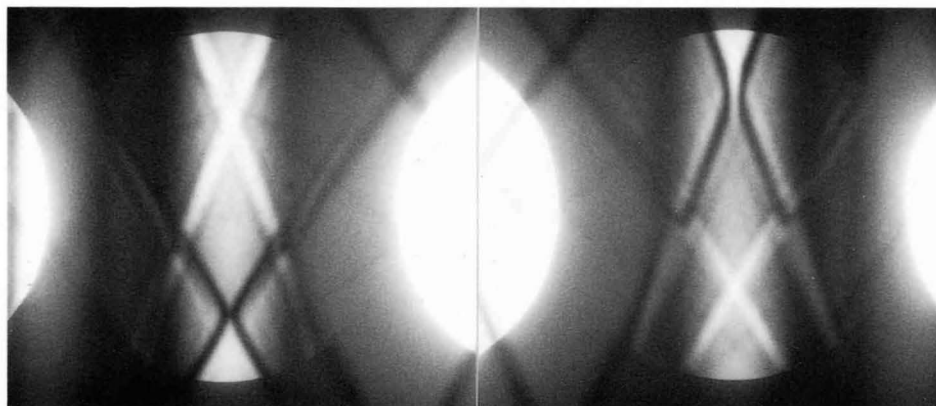
(a)

[5 1 0]



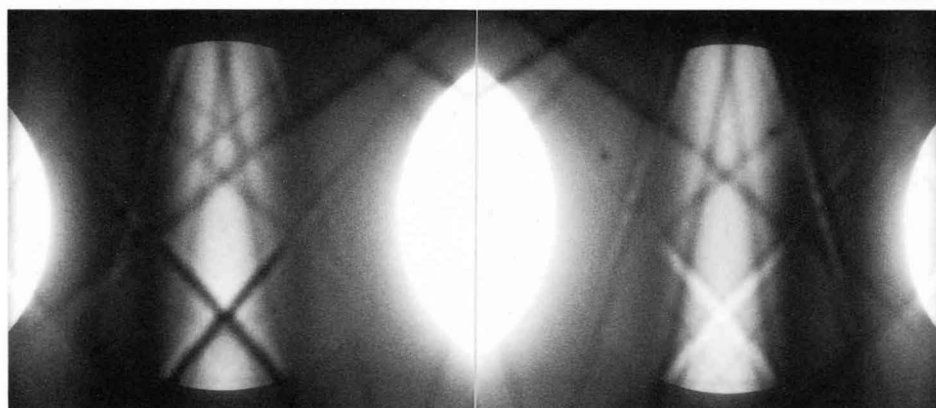
(b)

[4 1 0]



(c)

[2 1 0]

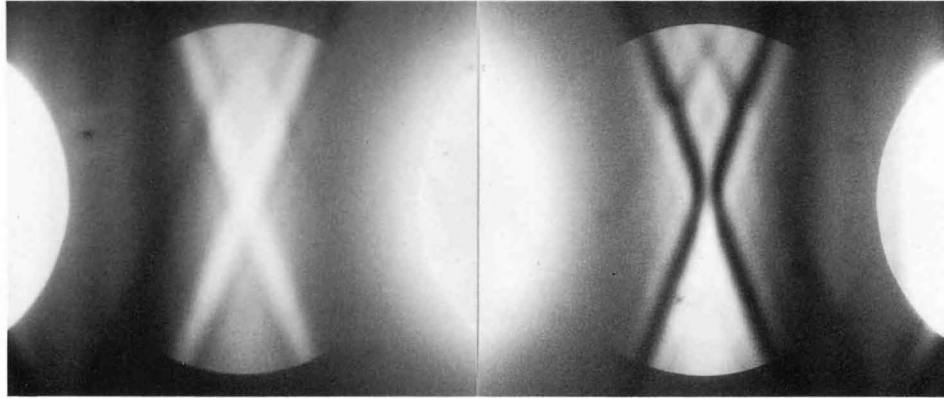


(d)

$00\bar{2}$

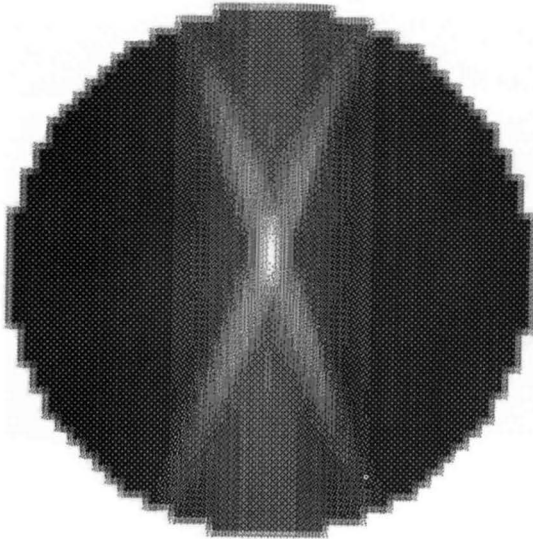
$002$

[625 262 0]

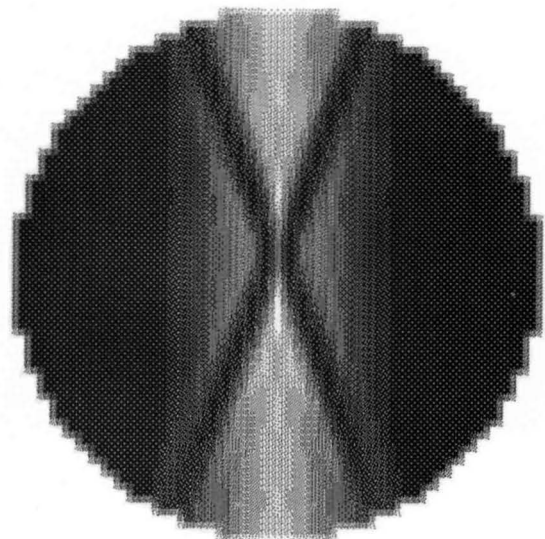


(e)

$00\bar{2}$



002



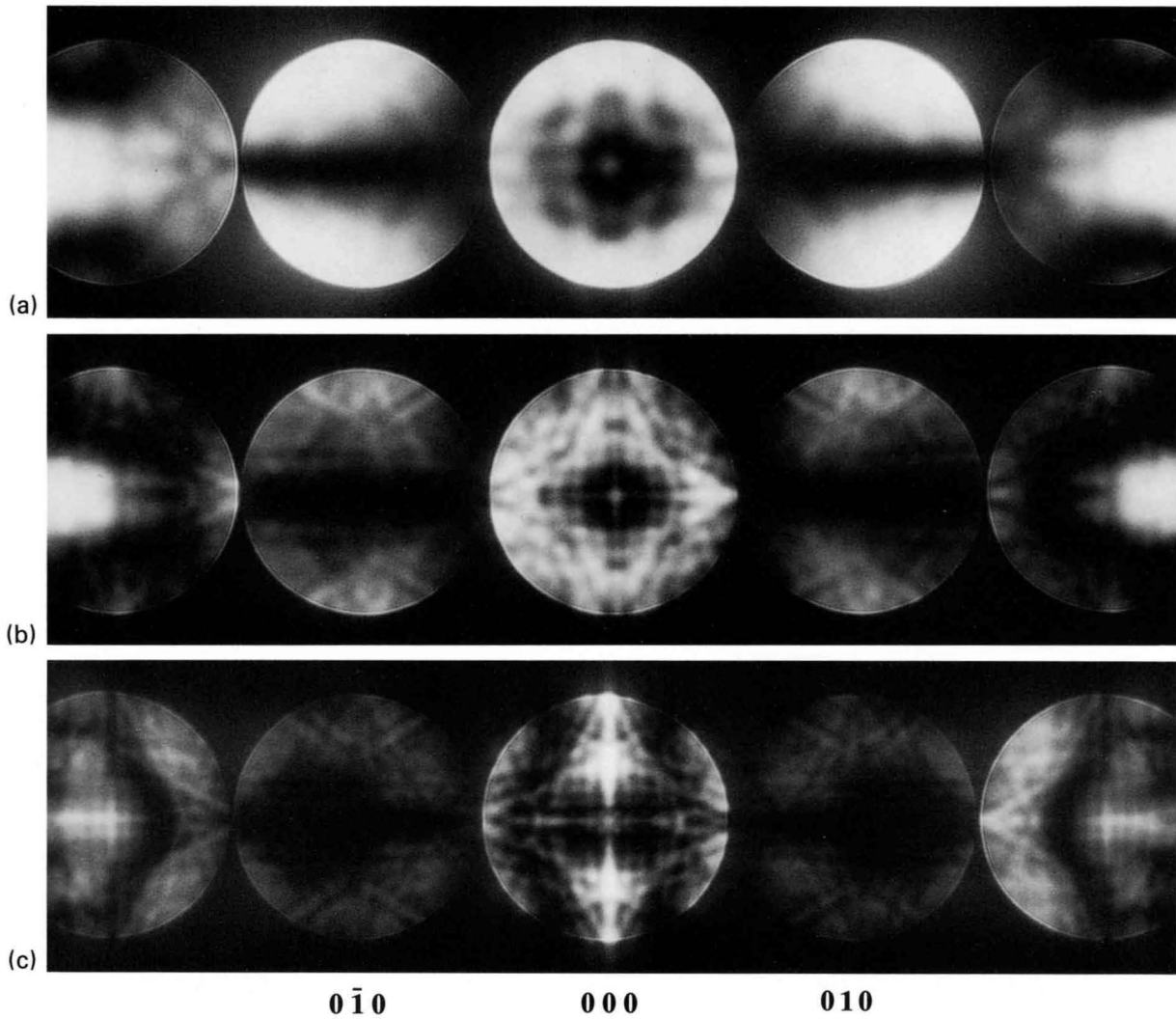
CBED patterns (a) to (e) were taken from GaAs at the settings of different azimuthal angles, clearly showing the lack of a symmetry  $2_R$ . The simulated 002 and  $00\bar{2}$  dark-field patterns at a thickness of 83.4 nm show a good agreement with Photo (e).

# *FeS<sub>2</sub>*

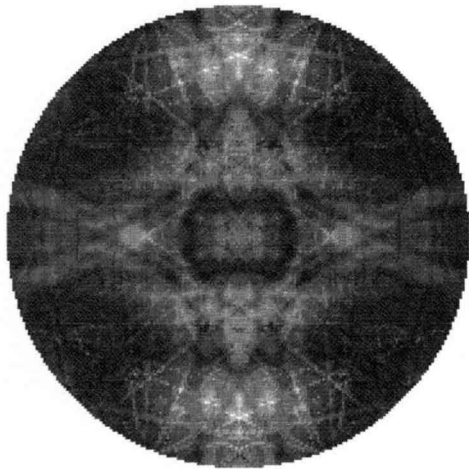
[100]

Thickness dependence of ZAP

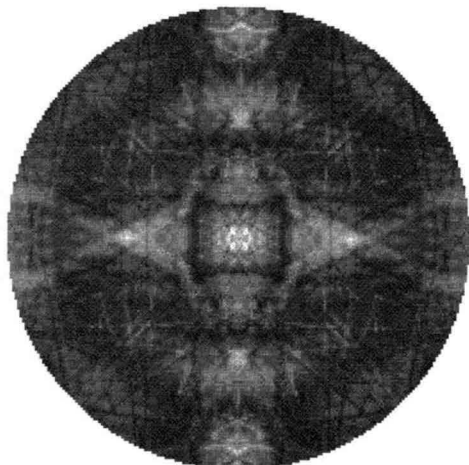
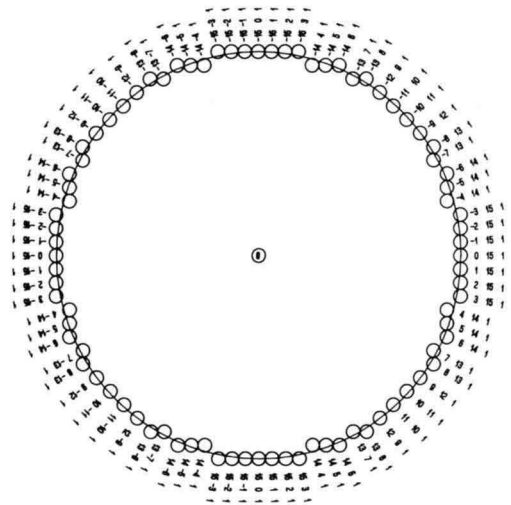
60 kV



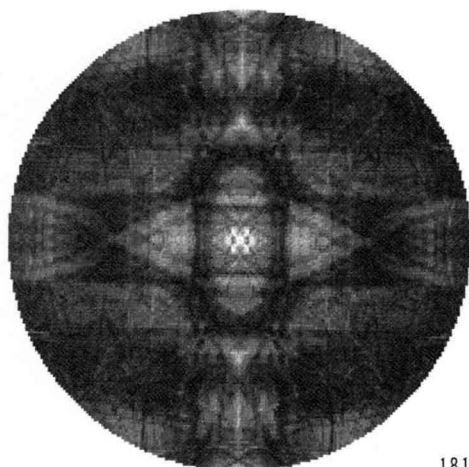
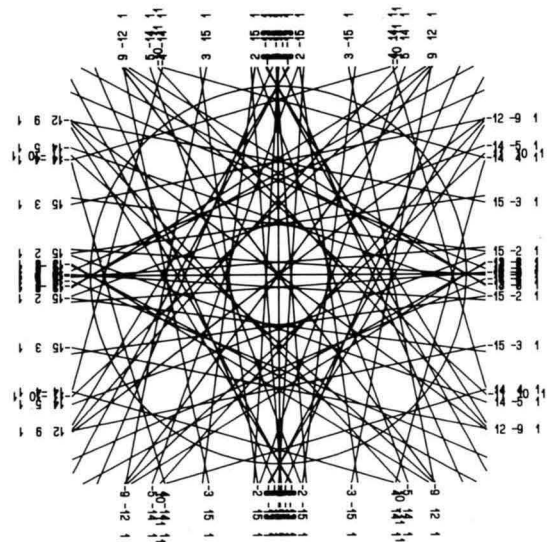
CBED patterns (a), (b) and (c) were taken from FeS<sub>2</sub> at the [100] incidence for three different thicknesses. The bright-field disks form light spots at their centers due to the reinforcement of the intensities of HOLZ lines. The bright-field patterns computed for three thicknesses using 37 ZOLZ and 84 HOLZ beams reproduced those light spots as shown on the opposite page.



108.1 nm



135.2 nm



162.2 nm

FeS2

[ 0 0 1 ]

61.9 kV

1 st Laue Zone

Holz-ring

(G= 0 0 0 excitation)

a=5.407Å

b=5.407Å

c=5.407Å

alpha=90°

beta =90°

gamma=90°

RADIUS OF HOLZRING

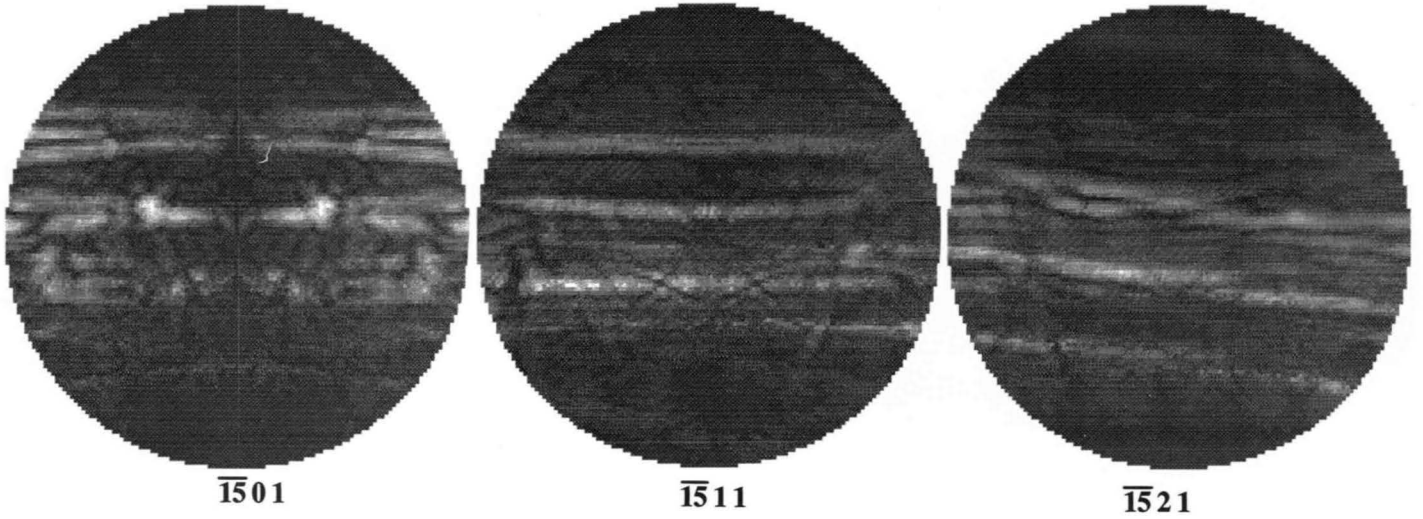
=2.7742 (1/Å)

HORIZONTAL DIRECTION

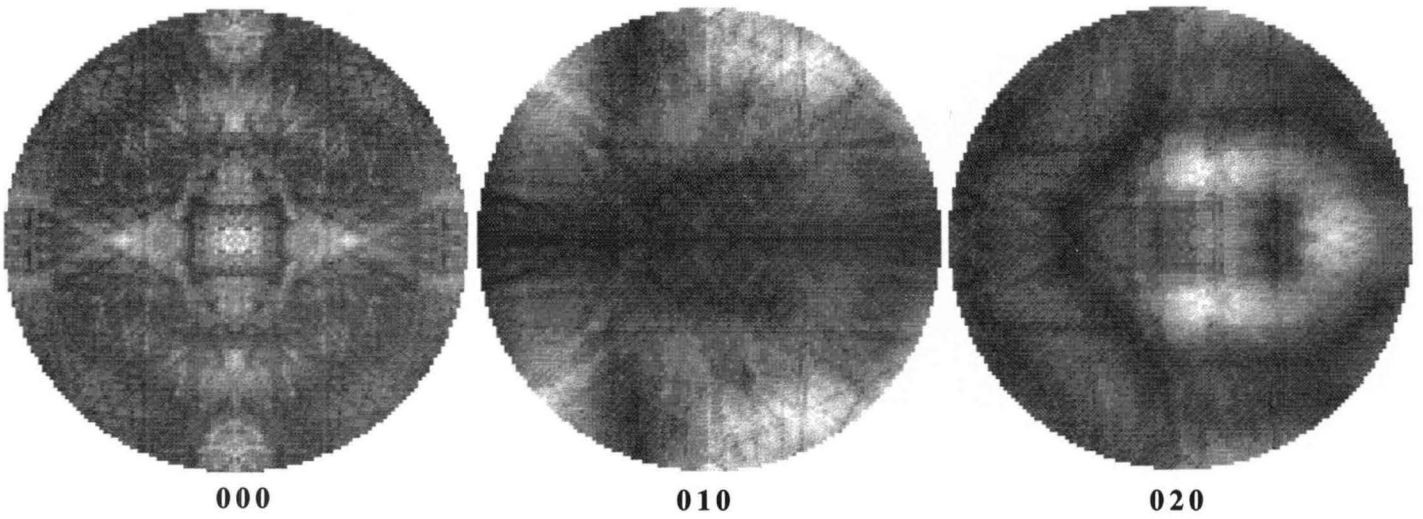
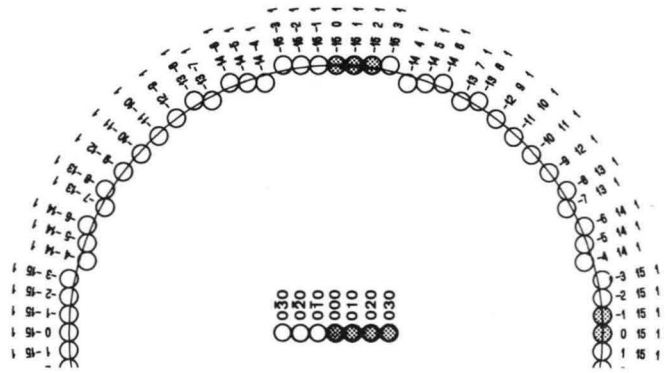
= [ 0 1 0 ]\*

181 \* 181 pixels  
type 3 enhancement curve / gamma-coef. = .5

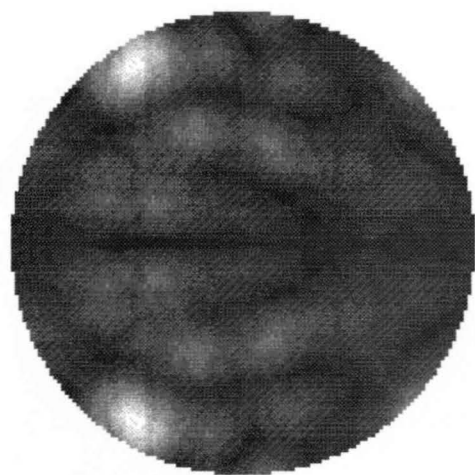
FeS<sub>2</sub> [001] 39 ZOLZ and 84 HOLZ beams, 61.9kV, thickness 135.2 nm



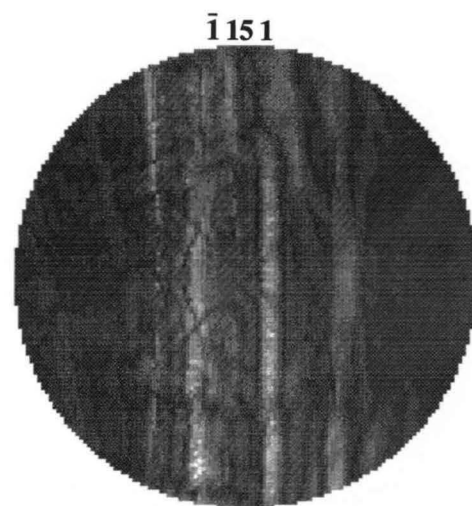
121 \* 121 pixels  
type 3 enhancement curve / gamma-coef. = .5



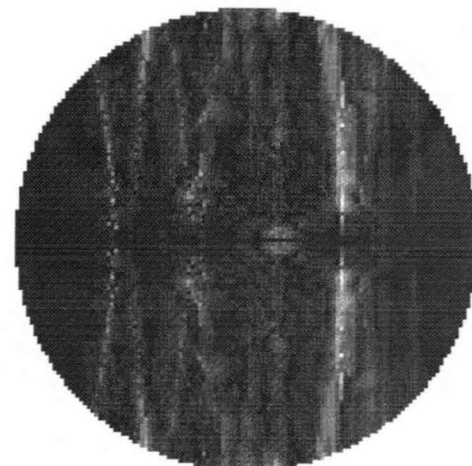
CBED patterns appearing not only in ZOLZ but also in HOLZ disks were simulated for  $\text{FeS}_2$  by fully dynamical computations. Fine structures of patterns in HOLZ disks were reproduced. GM lines due to the  $c$ -glide plane parallel to the (010) plane and the  $b$ -glide plane parallel to the (100) plane are clearly seen in the  $\bar{1}501$  and  $0151$  HOLZ disks, respectively.



030



$\bar{1}51$



0151

# Sensitivity of CBED Patterns to the Breakdown of Symmetry Elements

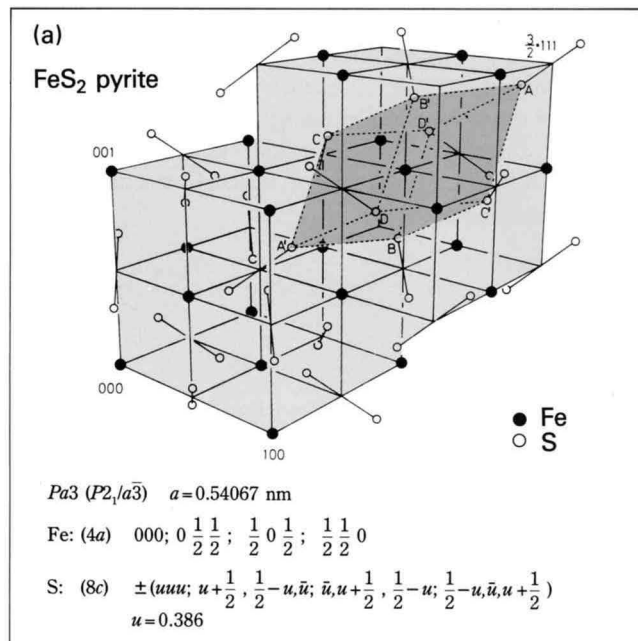
CBED patterns are known to be very sensitive to crystal symmetry, but their sensitivity has not ever been discussed quantitatively. The sensitivity was studied for FeS<sub>2</sub> by computer simulation. The crystal structure of FeS<sub>2</sub> is schematically shown in Fig. (a). Its space group is  $P2_1/a\bar{3}$ .

Two hypothetical crystal structures were formed by displacing two sulfur atoms, A and A' from the positions ( $u=0.386$ ) in the real crystal. 1) The atoms A and A' were displaced in the [111] direction to make them approach each other. The displacement caused the loss of 2<sub>1</sub> screw axes and *a*-glide planes, resulting in the space group  $P\bar{3}$ . 2) These atoms were displaced in the same sense in the [111] direction with their distance kept constant. The displacement caused the loss of inversion centers, resulting in the space group  $P3$ . The magnitude of the displacement  $\delta u$  was varied from  $-0.001$  to  $-0.01$  of the cell parameter, 0.5407 nm. Using 34-40 ZOLZ beams calculations of CBED patterns were carried out at an accelerating voltage of 60 kV and at the [001] electron incidence for three different thicknesses and for three different Bragg settings. It was studied how the CBED patterns change with gradual breakdown of crystal symmetries.

Figure (b) shows 010 dark-field CBED patterns computed at the 010 exact Bragg setting for five values of type 1) displacement. The pattern at extreme left was computed for a perfect crystal, which shows a cross of  $A_2$  and  $B_2$  GM lines with a symmetry  $2mm$ . As  $\delta u$  increases, the symmetry  $2mm$  changes into a symmetry  $1_R$ . The symmetry  $1_R$  is expected from ZOLZ (projection) interaction, even if the crystal has no symmetry. The breakdown of the symmetry  $2mm$  is already recognizable for  $\delta u = -0.001$ . For  $\delta u = -0.002$ , the breakdown is clearly seen as a deformed cross of the GM lines. Such deformed GM lines due to a slight breakdown of a 2<sub>1</sub> screw axis were already seen in the section of Mo<sub>2</sub>S<sub>3</sub>. The lower patterns in Fig. (b) are the difference patterns between the upper halves and lower halves of the original (upper) patterns. We define a quantitative measure of the difference,  $\Delta$ , as

$$\Delta = \frac{\sum_{\text{disk}} |I_u - I_l|}{\sum_{\text{disk}} (I_u + I_l)},$$

where  $I_u$  and  $I_l$  are the intensities at two pixels which are related by a horizontal mirror plane passing through

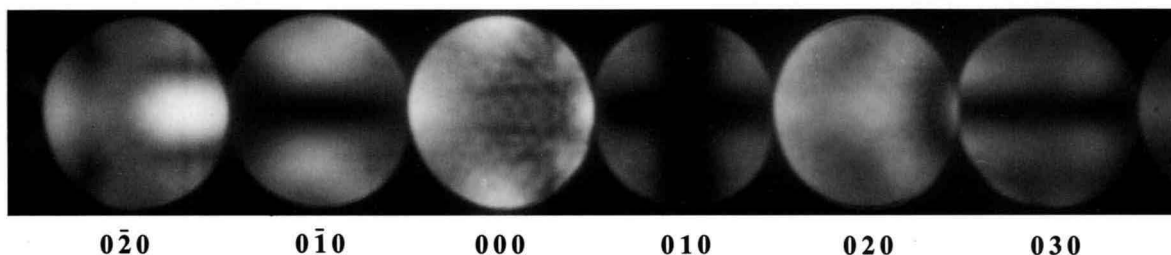


the center of the disk. The summing was carried out over the whole disk. The values of  $\Delta$  are given below the patterns. It should be noted that  $\Delta$  is 0.144 already for  $\delta u = -0.001$  (actual displacement of 0.00054 nm) and reaches 0.71 for a displacement of 0.0054 nm.

Figure (c) shows 0 $\bar{1}0$  dark-field CBED patterns computed at the 010 exact Bragg setting for the same displacements of Fig. (b). The pattern at extreme left was obtained again from a perfect crystal, which shows a symmetry  $m$  with an  $A_2$  GM line. As  $\delta u$  increases, the symmetry  $m$  is lost. The difference pattern is given below each original pattern. It is seen that the values of  $\Delta$  are smaller than those in Fig. (b).

Figures (d), (e) and (f) are three sets of CBED patterns, all computed at the 010 exact Bragg setting for thicknesses of 54.1 nm, 108.1 nm and 162.2 nm, respectively. Changes of patterns due to both the increase of  $\delta u$  and thickness are obviously seen. The next three sets of CBED patterns, (g), (h) and (i), were computed at the 030 exact Bragg setting for the same thicknesses, and the last three sets, (j), (k) and (l), were computed at the 050 exact Bragg setting. It is seen that the breakdown of the symmetries is the greatest for the first set and the smallest for the last set.

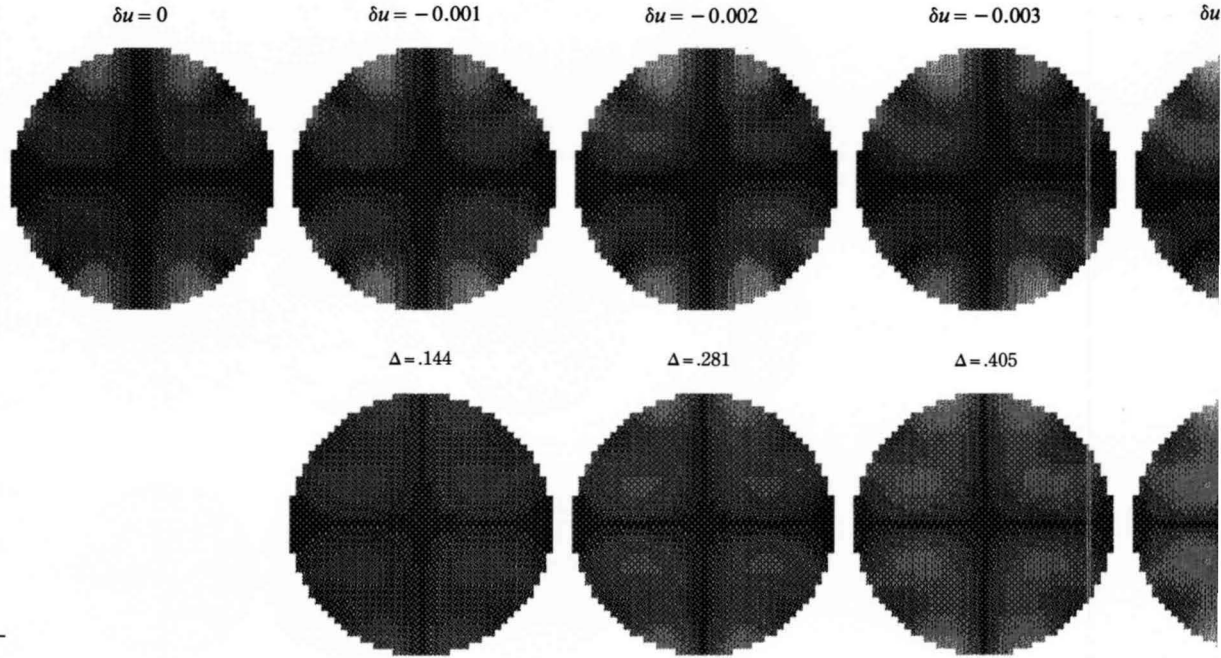
FeS<sub>2</sub> [001]  
010 excitation  
60 kV



**Breakdown of symmetry 2mm**

**FeS<sub>2</sub> [001], 010 excitation, 34 ZOLZ beams, 60 kV, thickness 108.1 nm**

(b) 010 reflections

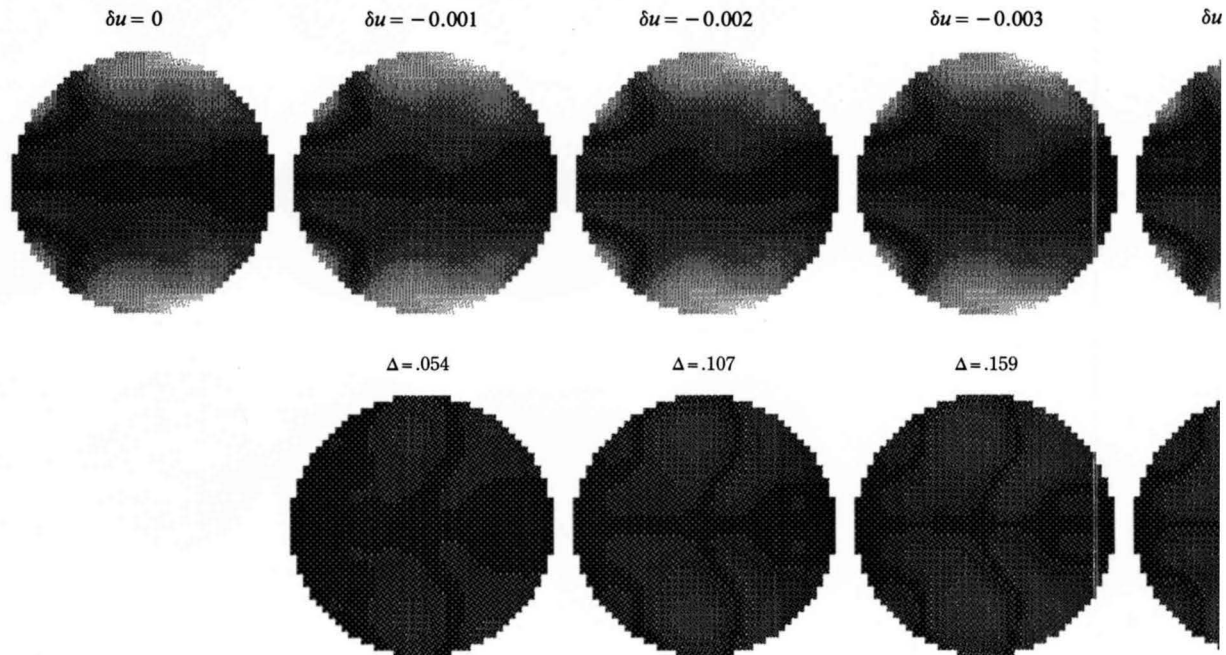


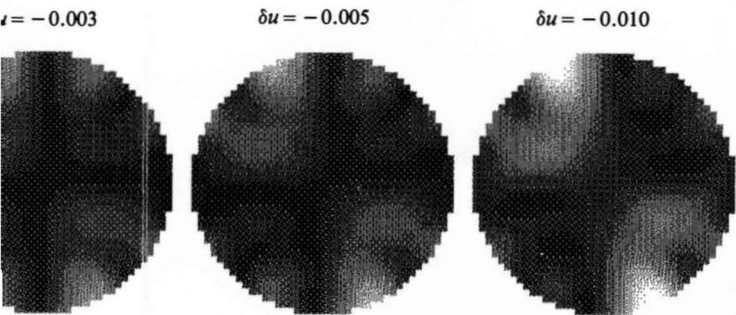
$$\Delta = \frac{\sum_{\text{disk}} |I_u - I_l|}{\sum_{\text{disk}} (I_u + I_l)}$$

**Breakdown of symmetry m<sub>v</sub>**

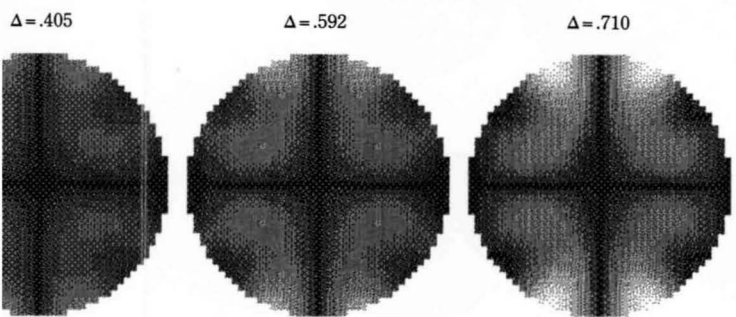
**FeS<sub>2</sub> [001], 010 excitation, 34 ZOLZ beams, 60 kV, thickness 108.1 nm**

(c) 010 reflections

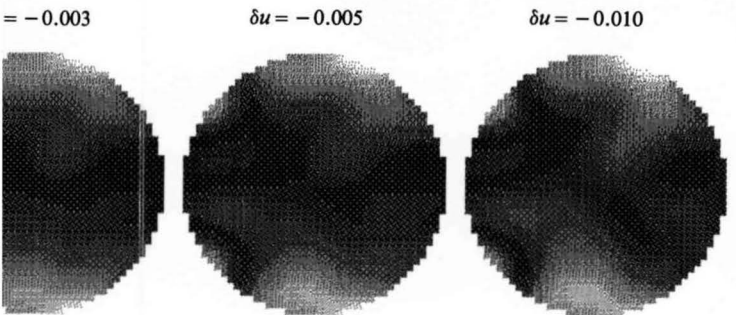




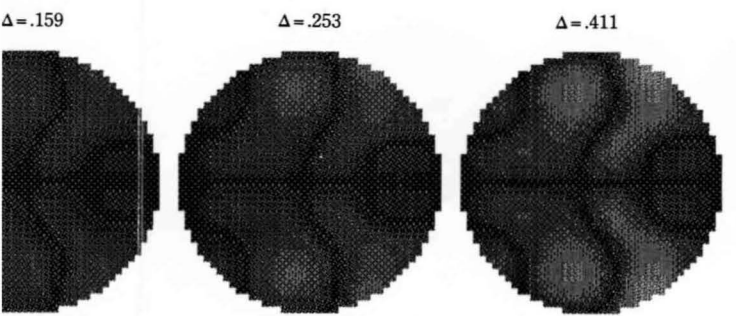
$2mm \rightarrow 1_R$  ( $Pa3 \rightarrow P\bar{3}$ )



Difference



$m_v \rightarrow 1$  ( $Pa3 \rightarrow P\bar{3}$ )



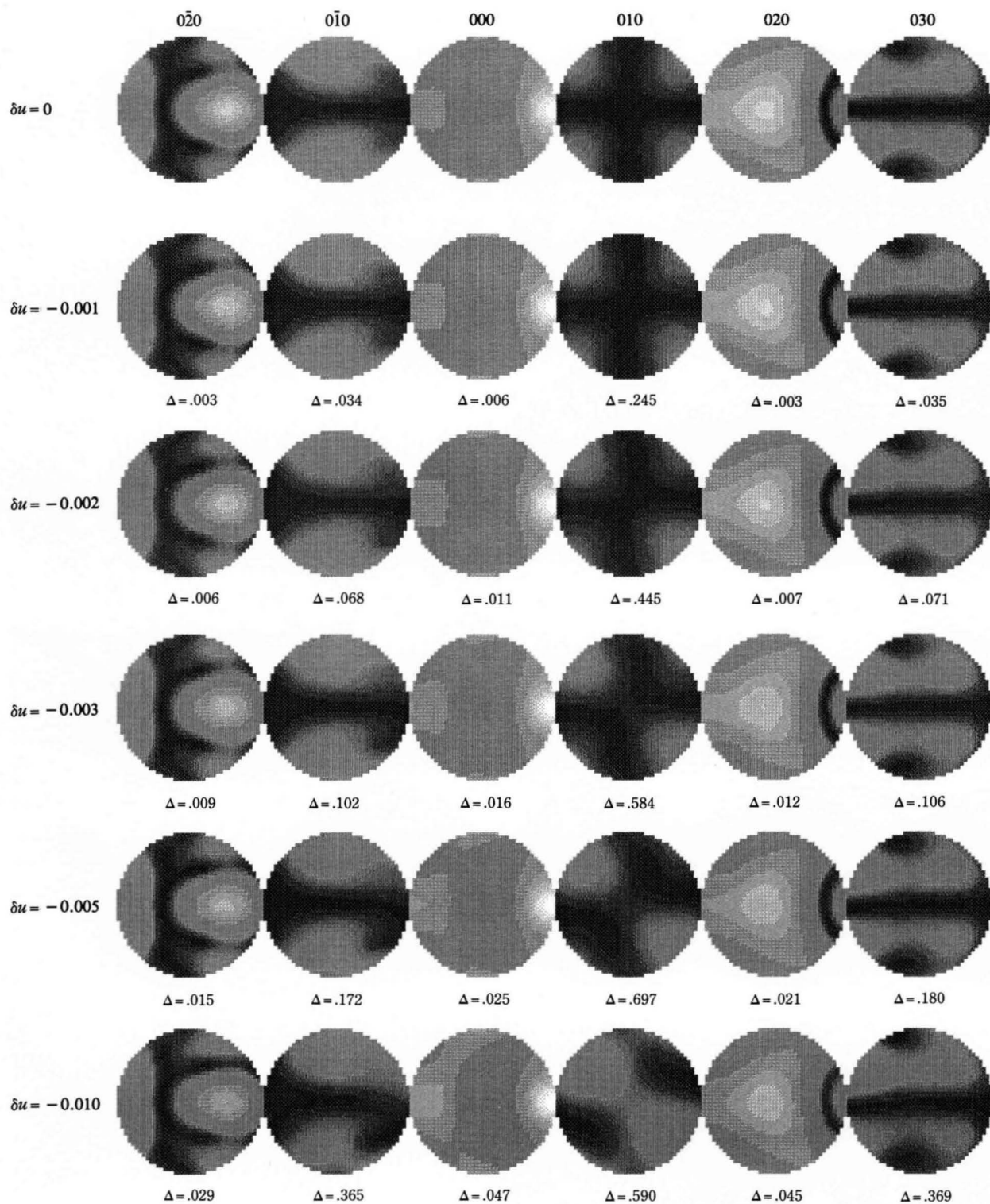
Difference

41 \* 41 pixels  
type 3 enhancement curve / gamma-coef. = .7

**Breakdown of symmetry  $m$ ,**

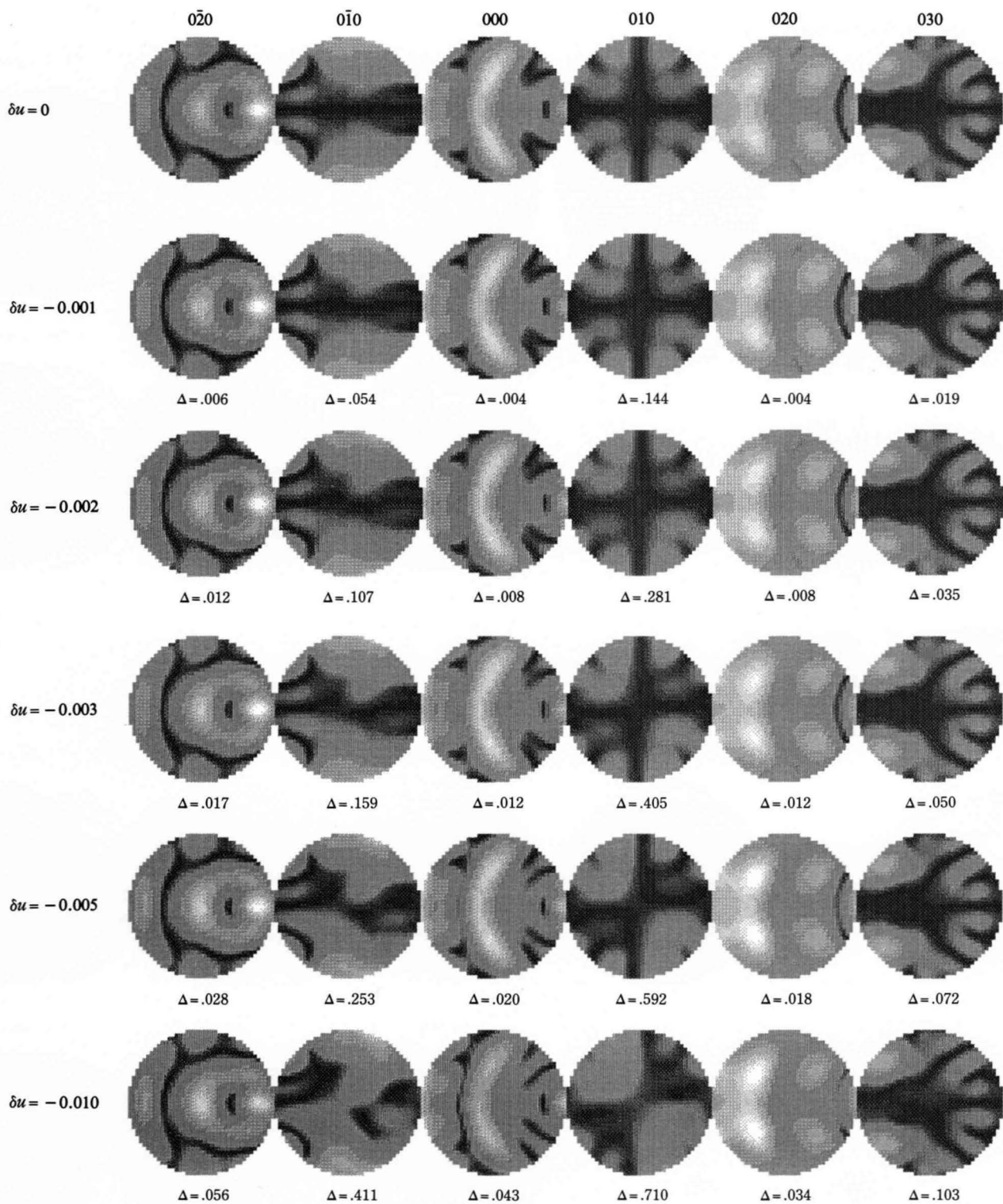
**FeS<sub>2</sub> [001], 010 excitation, 34 ZOLZ beams, 60kV**

(d) Thickness 54.1 nm



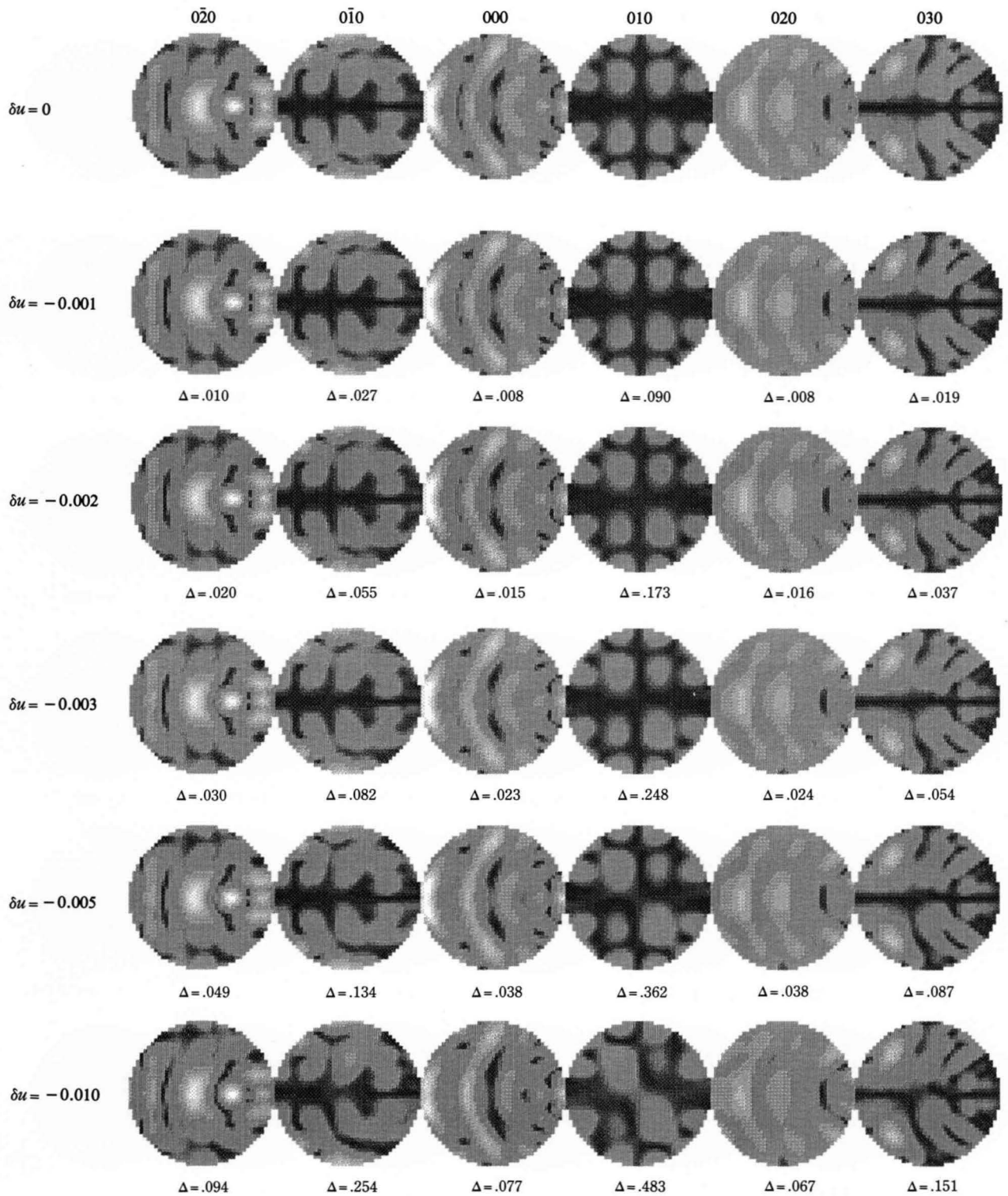
41 \* 41 pixels  
type 6 enhancement curve / gamma-coef. = 1.5

(e) Thickness 108.1 nm



41 \* 41 pixels  
type 6 enhancement curve / gamma-coef. = 1.5

(f) Thickness 162.2 nm

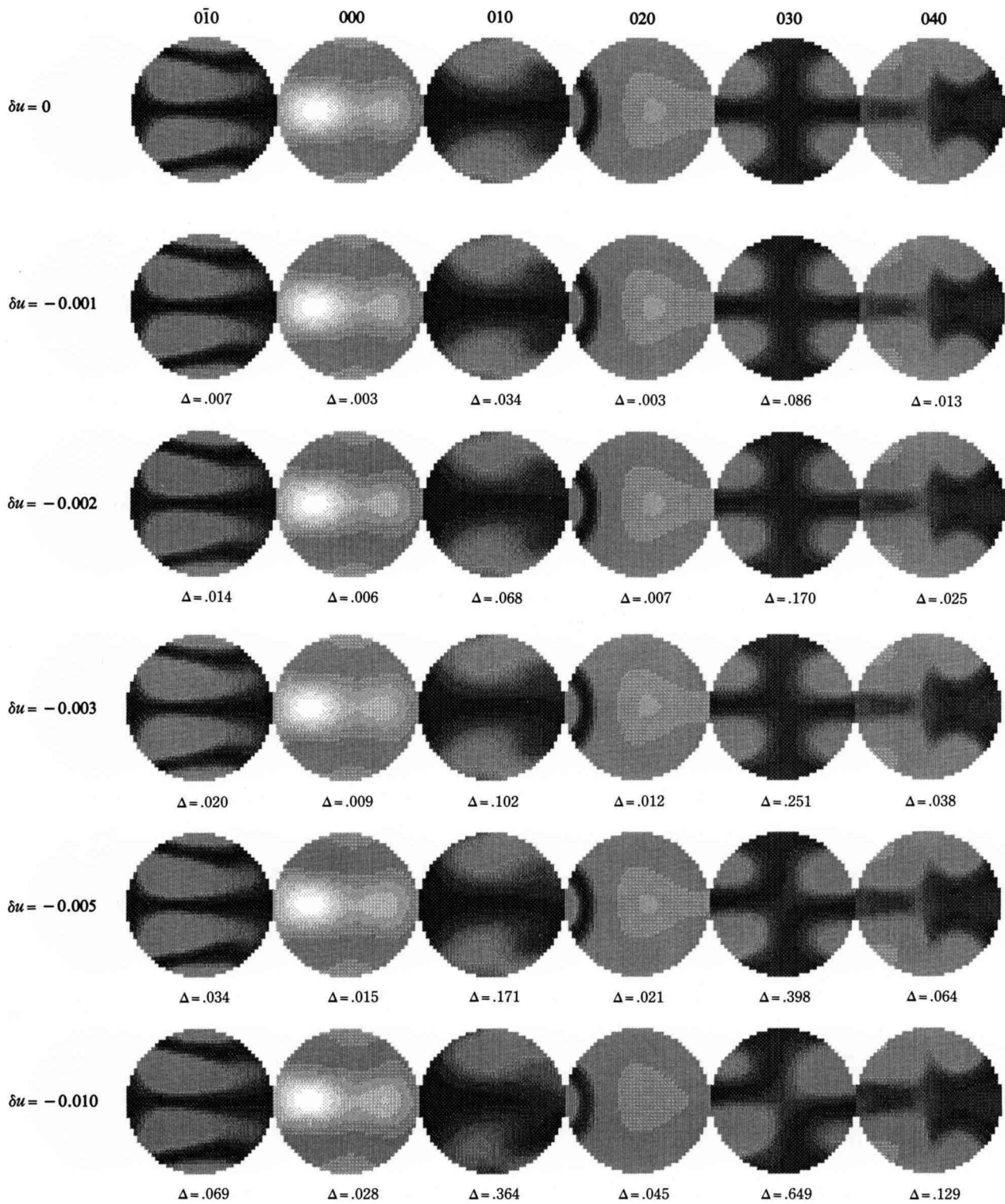


41 \* 41 pixels  
 type 6 enhancement curve / gamma-coef. = 1.5

**Breakdown of symmetry  $m_v$**

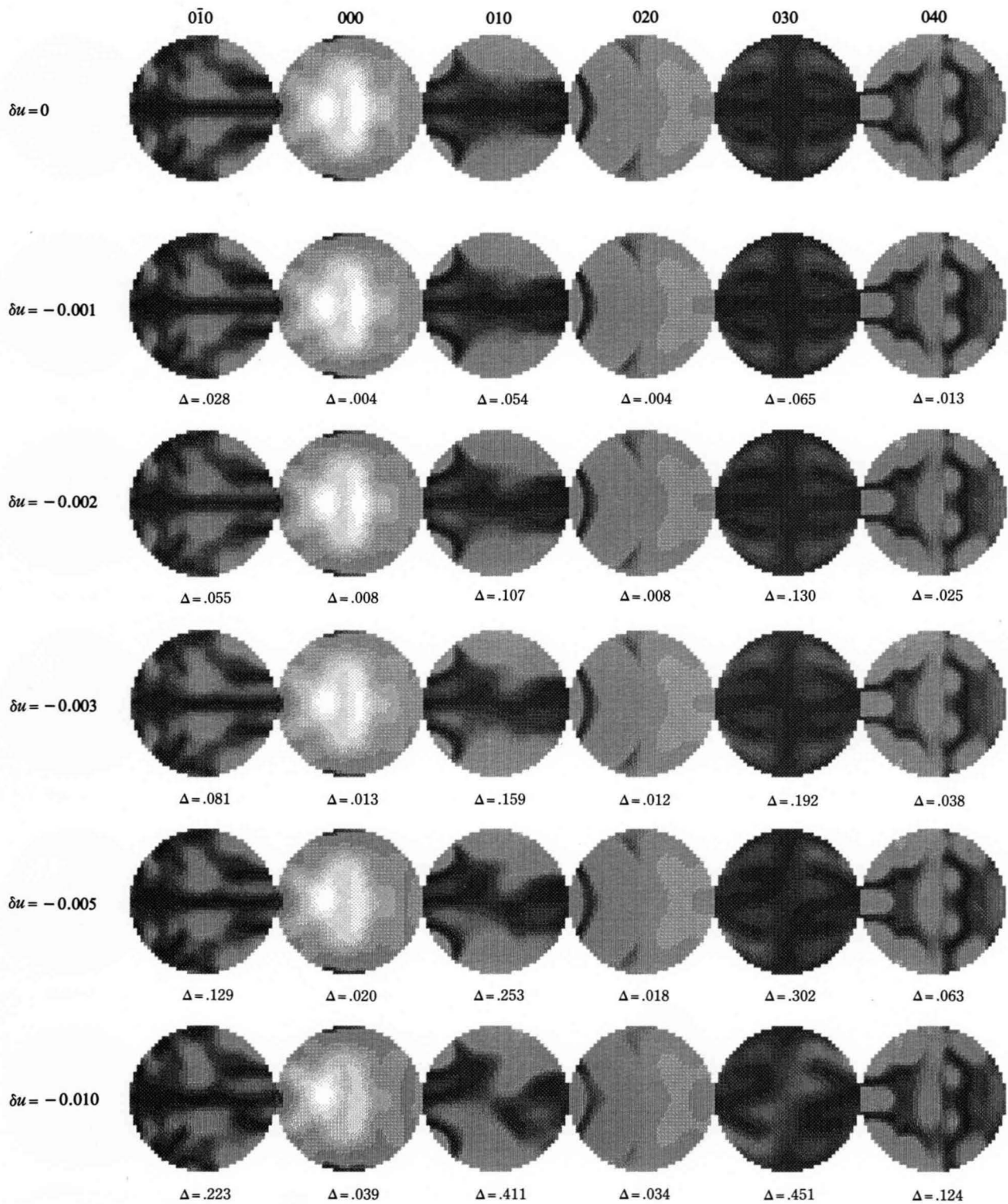
**FeS<sub>2</sub> [001], 030 excitation, 34 ZOLZ beams, 60kV**

(g) Thickness 54.1 nm



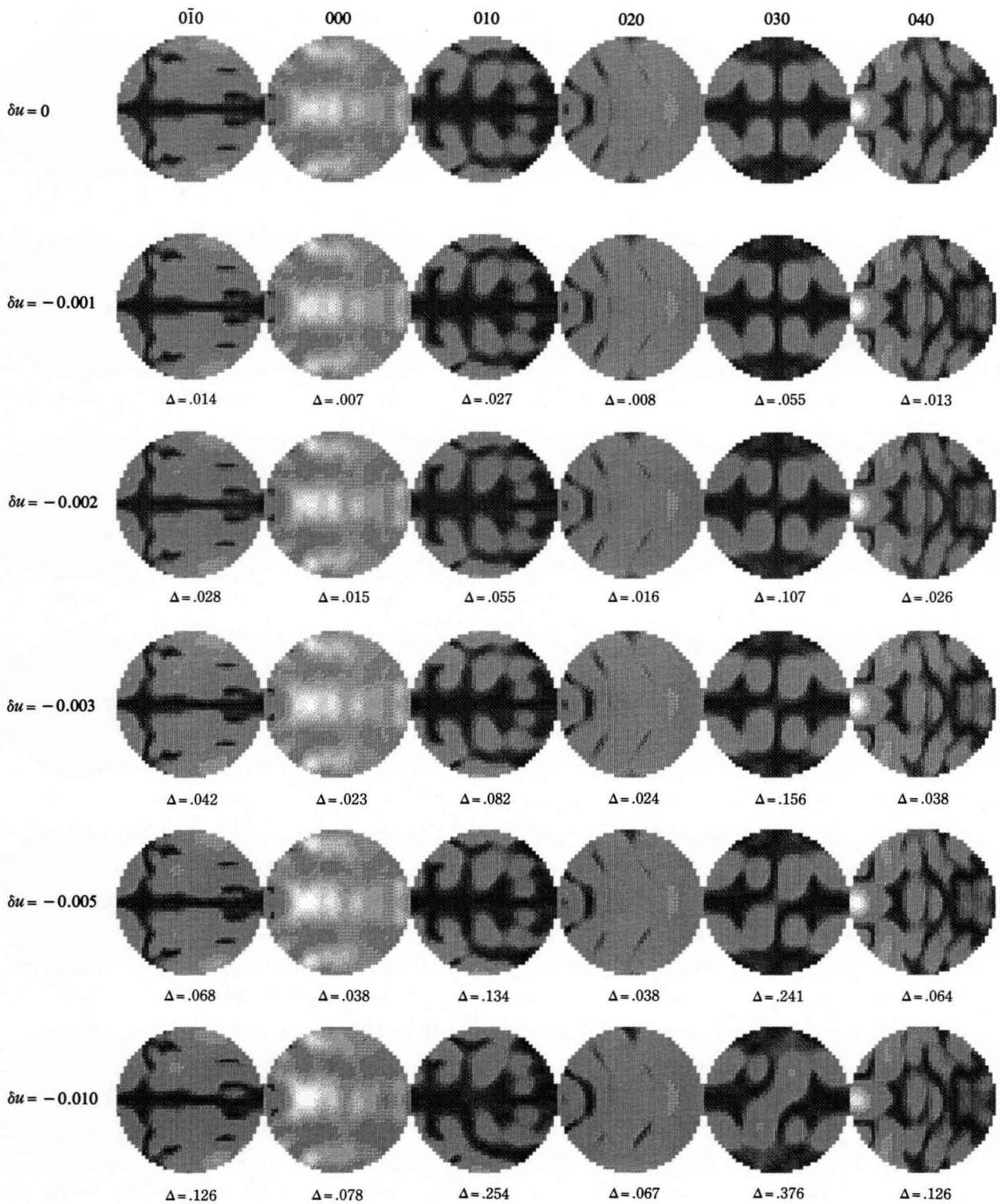
41 \* 41 pixels  
type 6 enhancement curve / gamma-coef. = 1.5

(h) Thickness 108.1 nm



41 \* 41 pixels  
 type 6 enhancement curve / gamma-coef. = 1.5

(i) Thickness 162.2 nm

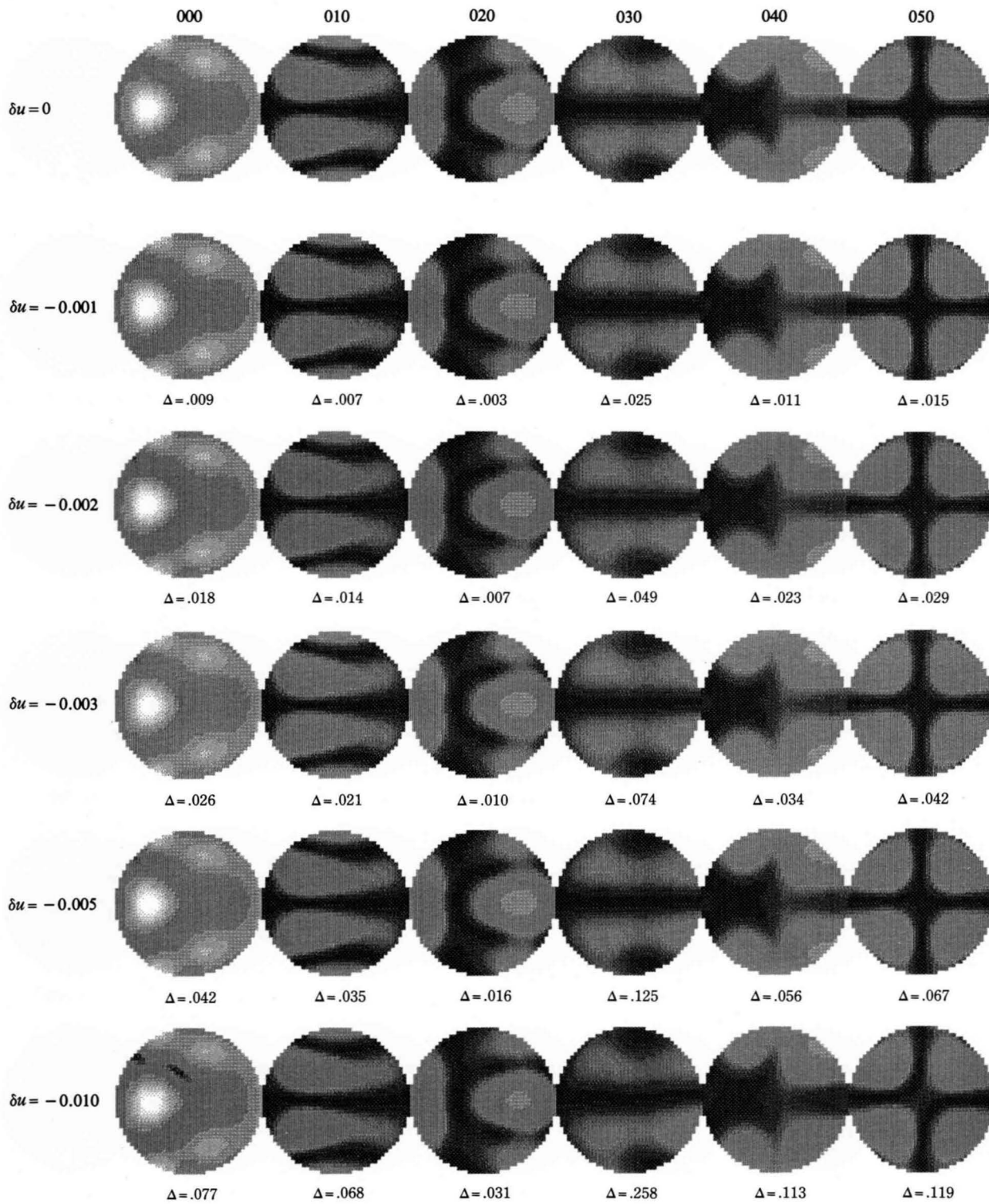


41 \* 41 pixels  
 type 6 enhancement curve / gamma-coef. = 1.5

**Breakdown of symmetry  $m_v$**

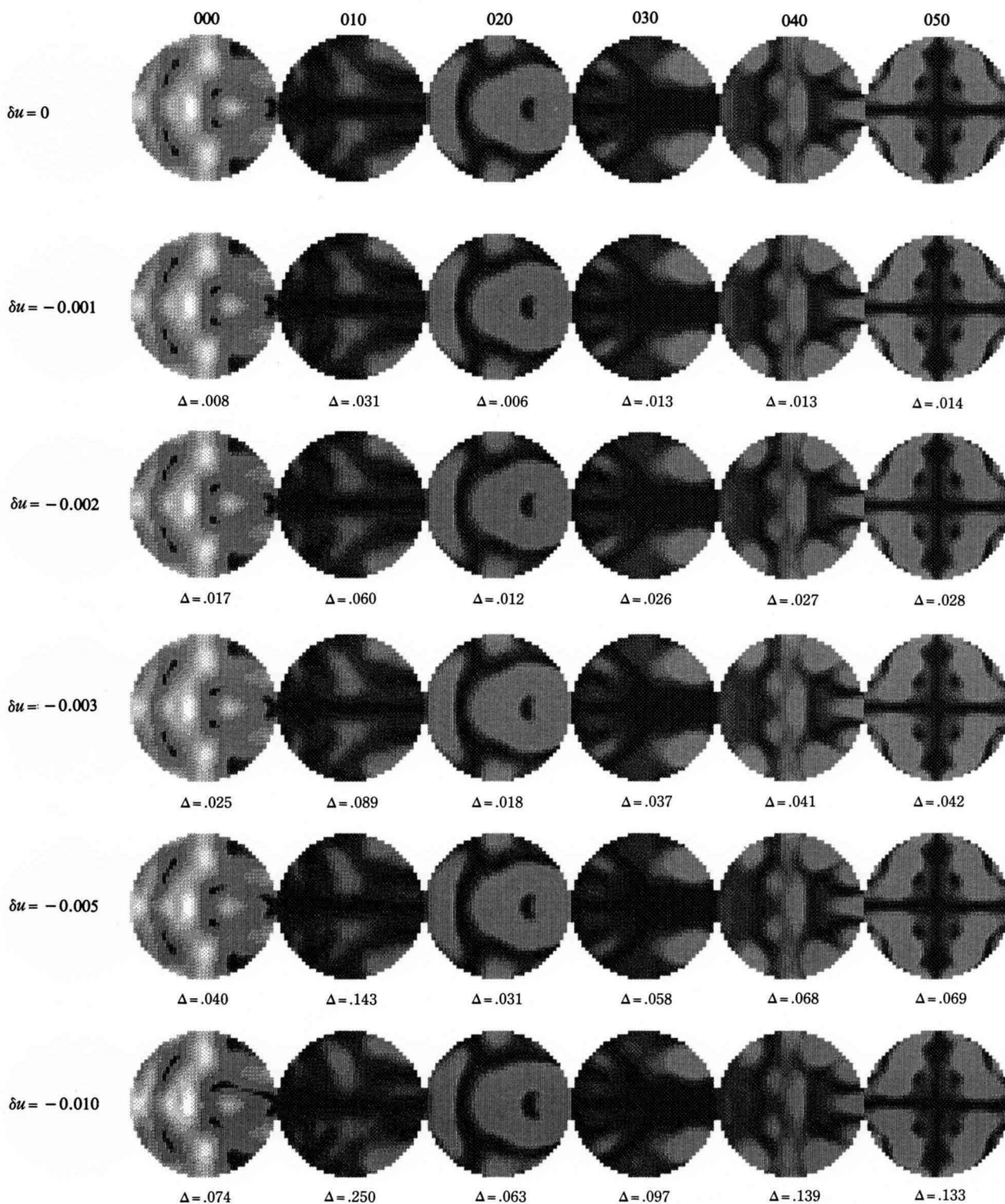
**FeS<sub>2</sub> [001], 050 excitation, 40 ZOLZ beams, 60kV**

(j) Thickness 54.1 nm



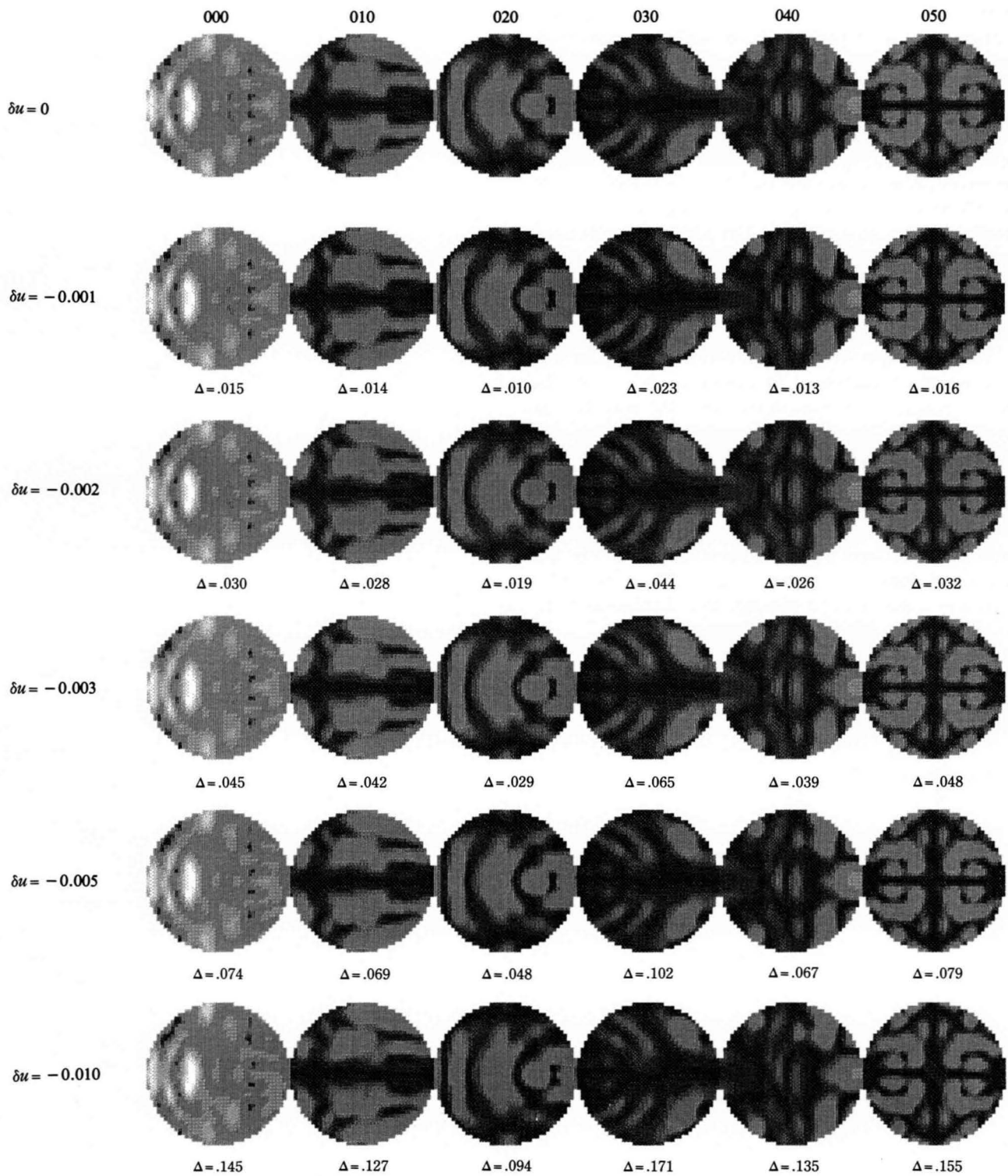
41 \* 41 pixels  
type 6 enhancement curve / gamma-coef. = 1.5

(k) Thickness 108.1 nm



41 \* 41 pixels  
 type 6 enhancement curve / gamma-coef. = 1.5

(I) Thickness 162.2 nm



41 \* 41 pixels  
 type 6 enhancement curve / gamma-coef. = 1.5

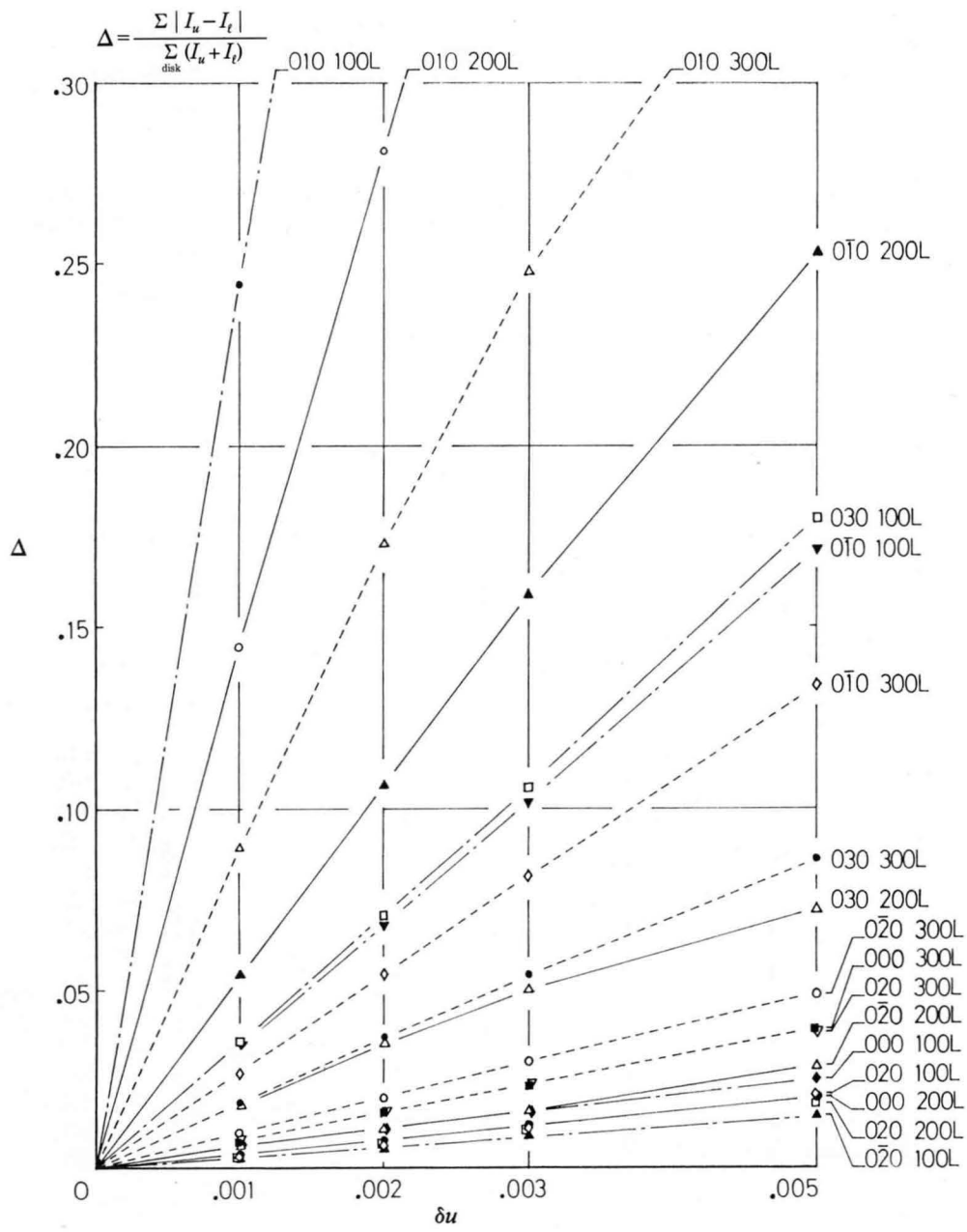
The values of  $\Delta$  were plotted as a function of  $\delta u$ , where the values of  $\Delta$  for  $\delta u = -0.01$  were omitted, because the measure  $\Delta$  is no more suitable for correctly expressing the intensity difference for such a large value of  $\delta u$ . Figures (a), (b) and (c) give the results of the 010, 030 and 050 Bragg settings. The highest sensitivity was obtained for the 010 Bragg setting and the lowest one for the 050 Bragg setting. The reflections with larger excitation errors show low sensitivities. These facts indicate that the reflections which suffer from strong dynamical interaction show high sensitivity. The odd order reflections are more sensitive to the breakdown of the symmetries than the even order reflections, because the intensities of the even order (kinematically allowed) reflections are affected little by the displacements of the sulfur atoms. Thickness changes of the sensitivity is seen. The 010 reflection at a thickness of 54.1 nm (Fig. (a)) shows the highest sensitivity. It is quite sure that the sensitivity is closely related to the effective extinction distance of this reflection and is lowered with increasing thickness due to the absorption effect.

If it is assumed that a difference of  $\Delta = 0.15$  is detectable in experimental patterns, which must, of course, be taken from specimens with uniform thickness, Fig. (a) indicates, at least for the present case, that CBED patterns have a potential to distinguish a displacement of less than  $\delta u = 0.001$  in mean atomic positions.

**Breakdown of symmetry  $m_v$**

**FeS<sub>2</sub> [001], 34 ZOLZ beams, 60 kV**

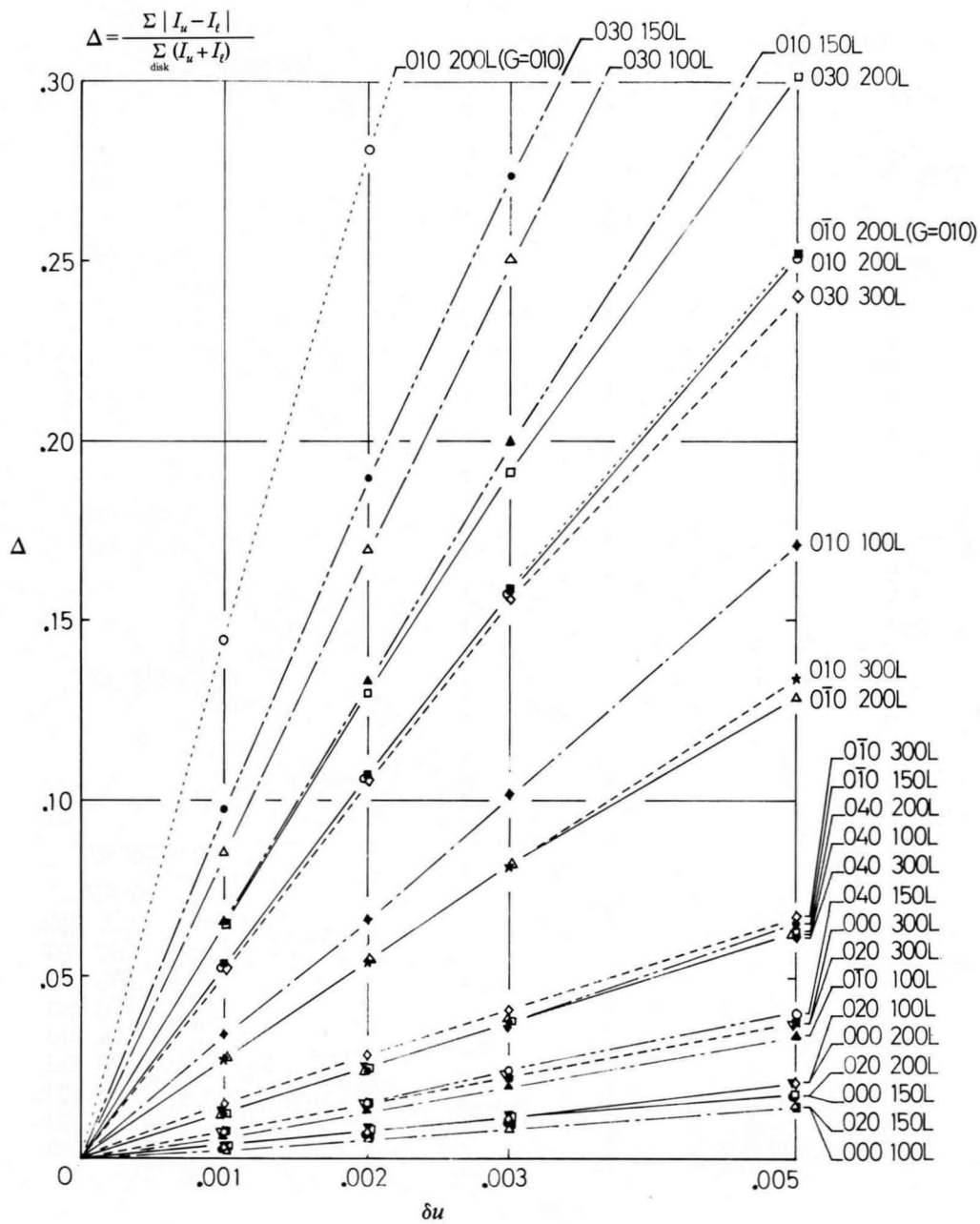
(a) 010 Bragg setting



# Breakdown of symmetry $m_v$

FeS<sub>2</sub> [001], 34 ZOLZ beams, 60 kV

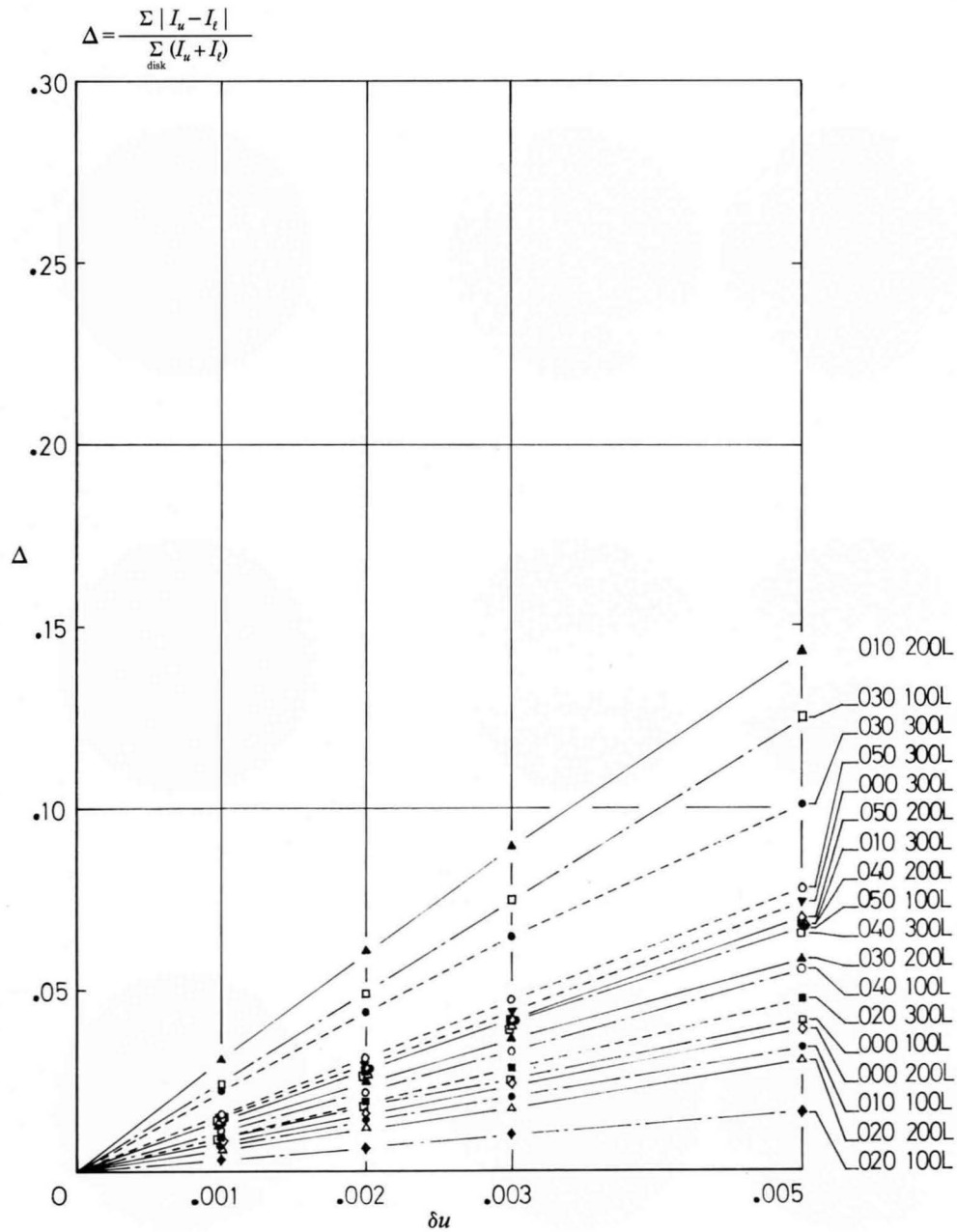
(b) 030 Bragg setting



**Breakdown of symmetry  $m_v$**

**FeS<sub>2</sub> [001], 40 ZOLZ beams, 60 kV**

(c) 050 Bragg setting



100L = 54.1nm

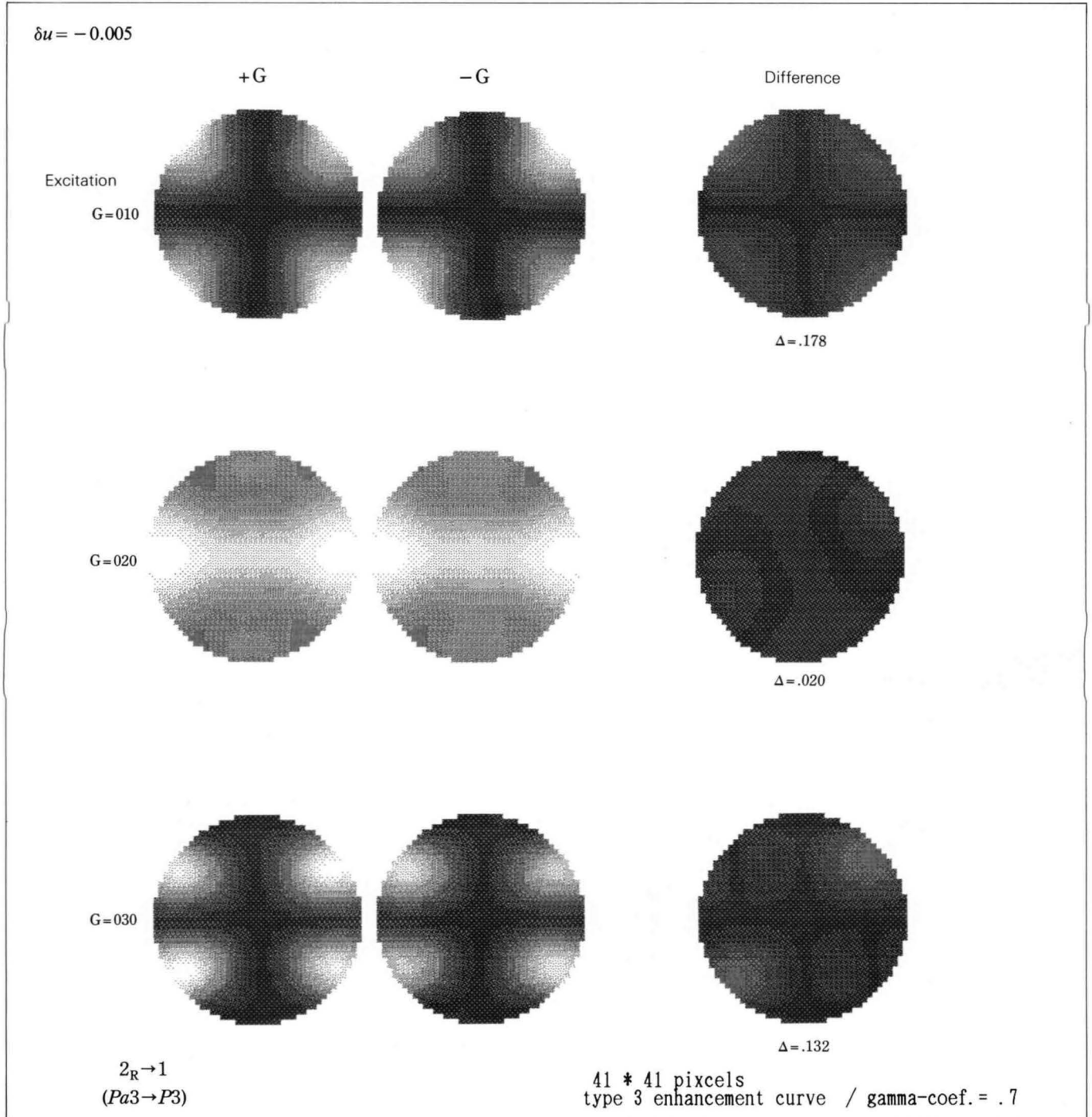
## Breakdown of symmetry $2_R$

$\text{FeS}_2$  [001], 34 or 37 ZOLZ beams, 60 kV

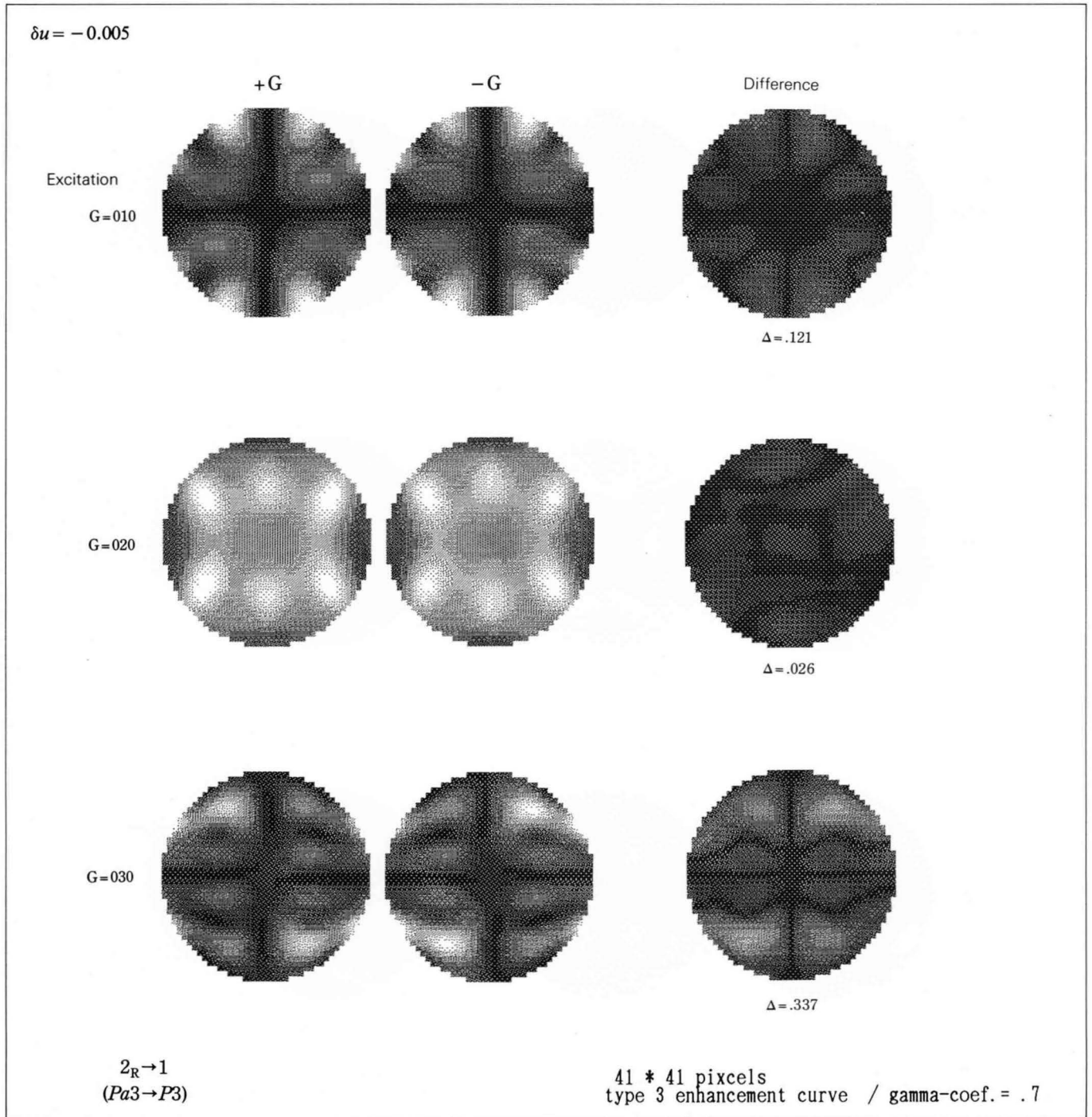
Figures (d), (e) and (f) show  $\pm G$  dark-field patterns computed for the type 2) displacement with  $\delta u = -0.005$  at three different thicknesses. The breakdown of a symmetry  $2_R$  due to an inversion center is seen. The difference pattern for each pair and the value of  $\Delta$ , which was defined in a similar manner to the previous case, are given. The value of  $\Delta$  was plotted as a function of  $\delta u$ .

It was found that the value of  $\Delta$  varies linearly to a good approximation for the values of  $|\delta u|$  smaller than 0.005. The sensitivity in this case is lower than that for the mirror symmetry. The  $\pm 030$  pair shows the highest sensitivity for a thickness of 108.1 nm.

(d) Thickness 54.1 nm



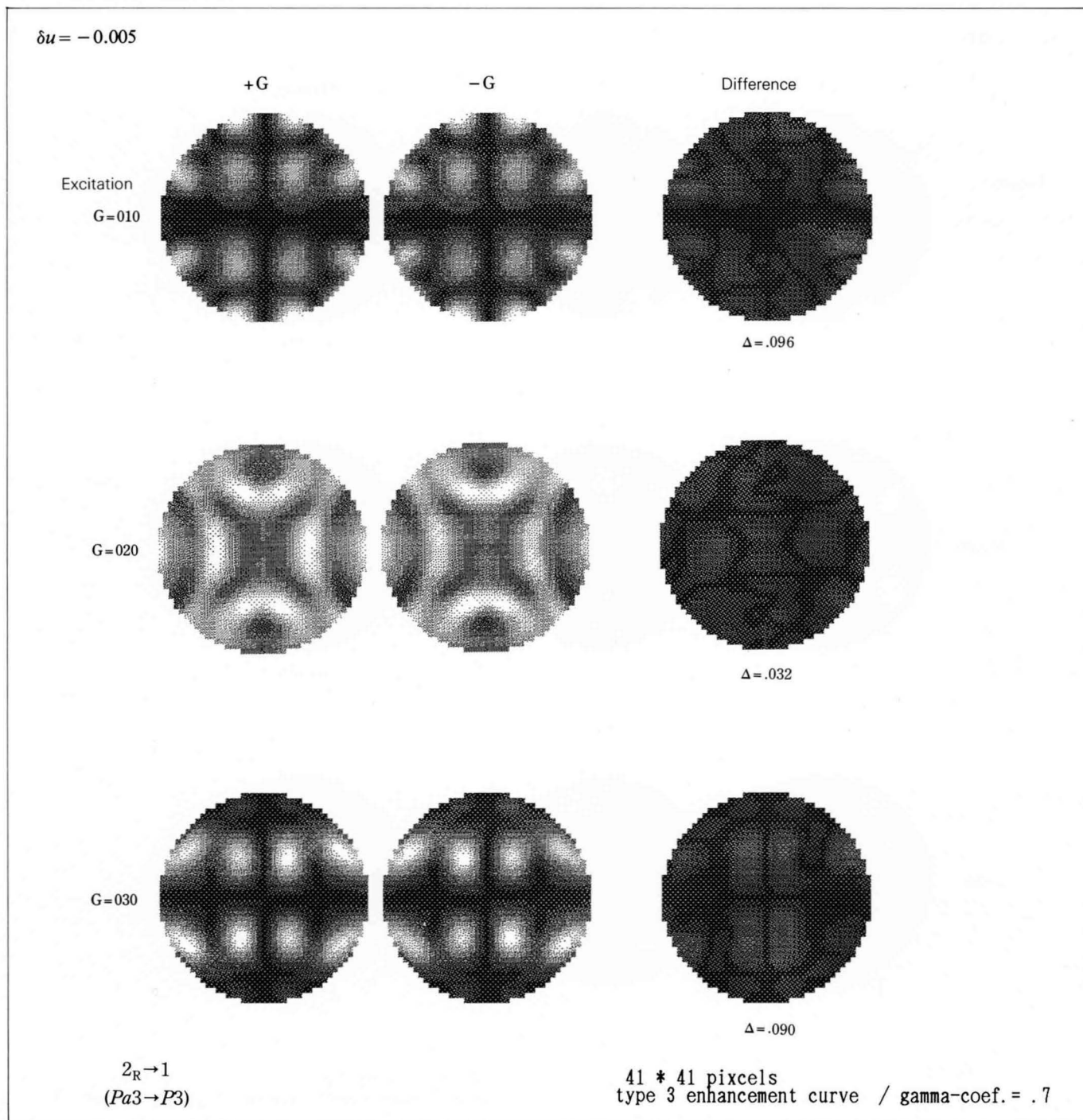
(e) Thickness 108.1 nm



# Breakdown of symmetry $2_R$

FeS<sub>2</sub> [001], 34 or 37 ZOLZ beams, 60kV

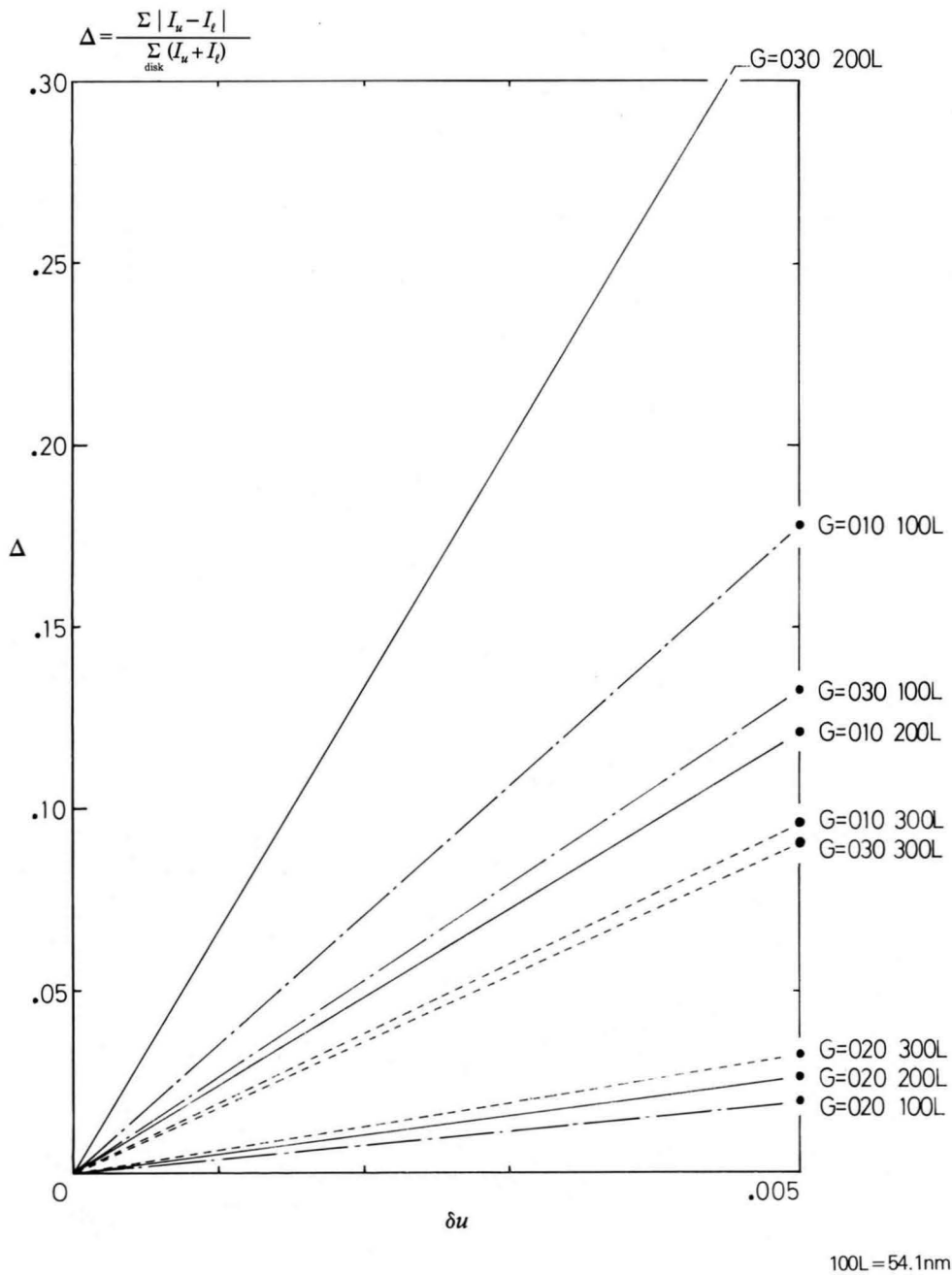
(f) Thickness 162.2 nm



**Breakdown of symmetry 2<sub>R</sub>**

**FeS<sub>2</sub> [001], 34 or 37 ZOLZ beams, 60kV**

(g) ± G Bragg setting



# *Lattice Defects*

# Stacking Faults

Electron microscopy has made a great success in the identification of lattice defects [a]. CBED also allows us to identify them. The observation of a lattice defect using CBED was first carried out by Johnson [19] for a stacking fault which lies parallel to the surface of a graphite foil, where the symmetry of a whole pattern, 6mm, which is expected from a perfect crystal, changed into a symmetry of 3m. Book I contains such examples. We investigated the method to determine the displacement vector of a stacking fault [21,22]. Rocking curves obtained from a faulted region are different from those of a perfect region in a manner characteristic of the displacement between two crystals at the fault. We shall describe three methods to investigate stacking faults.

The first method is to use ZOLZ reflections, which is an adaptation of the electron-microscope-image method for identifying a stacking fault. That is, the value of  $\alpha = 2\pi\mathbf{g}\cdot\mathbf{R}$  is determined by the examination of rocking curves obtained from near the top and bottom edges of the fault, where  $\mathbf{R}$  is the displacement vector for atoms at the fault and  $\mathbf{g}$  is the reflection vector. The displacement vector  $\mathbf{R}$  is determined with the help of the sense of tilt of the faulted plane with respect to the specimen surface. The sense of tilt must be determined by a separate method. We shall describe later a CBED method to determine this sense.

The inevitable illumination of a large specimen area in the LACBED method, the second method, is sometimes a disadvantage for the investigation of perfect crystals, but it is a great advantage for the identification of lattice defects. It is noted that the LACBED pattern is neither a pure diffraction pattern nor, of course, a microscope image. The LACBED pattern contains information on both reciprocal and real spaces, since the specimen is illuminated over a wide angular and a wide spatial spread. The LACBED method can identify the displacement vector while its sign is left undetermined.

The third method is to use HOLZ reflections, which makes the best use of the advantage of CBED. HOLZ lines obtained from a faulted area have simple and easily distinguishable profiles compared with those of ZOLZ reflections. Plural HOLZ lines appear simultaneously in one CBED pattern. These two facts enable the unambiguous determination of the displacement vector  $\mathbf{R}$  (including its sign) without knowing the sense of tilt of the fault. Therefore, this method can easily determine whether the fault is intrinsic or extrinsic, without such complication as occurs in the electron-microscope-image method. This method is experimentally easier than the first method, since the former method allows a rough setting of the incident beam at a position around the middle of the fault, while the latter requires a rather accurate setting of the incident beam to a position in a narrow edge area. It should be noted that the CBED methods are based upon

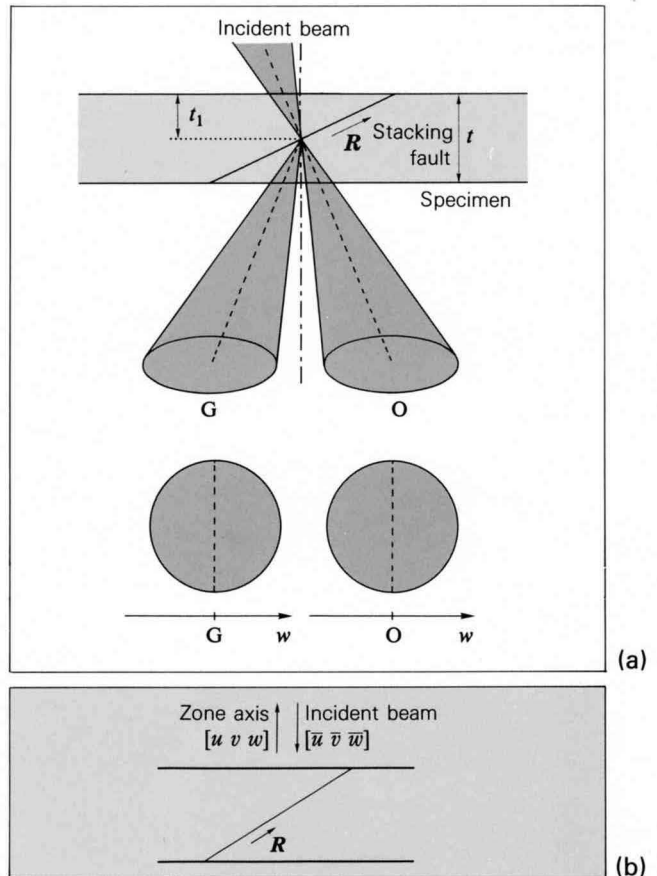
the dynamical diffraction theory but do not utilize the anomalous absorption effect. As a result, the third method has been successfully applied to the identification of a stacking fault in a thin specimen.

Figure (a) shows the side view of a specimen containing a stacking fault and a convergent beam illuminating the fault, where  $t$  is the thickness of the specimen and  $t_1$  is that of the upper crystal, at which the incident beam meets the stacking fault. The positive direction of the excitation error  $w$  is directed from the dark-field disk to the bright-field disk. For face-centered cubic crystals,  $\alpha$  takes a value of  $+(2/3)\pi$ ,  $-(2/3)\pi$  or 0.

Figure (b) gives a definition of the senses of the displacement vector, zone axis and incident beam. The displacement vector  $\mathbf{R}$  is defined as the displacement of the lower crystal with respect to the upper crystal. The positive direction of the zone axis is taken upward from the specimen. The electron beam runs in the  $[\bar{u} \bar{v} \bar{w}]$ .

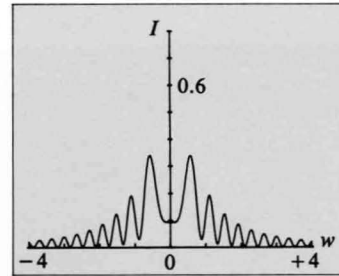
## Reference

- [a] P.B. Hirsch, A. Howie, R.B. Nicholson, D.W. Pashley and M.J. Whelan: *Electron Microscopy of Thin Crystals*, Butterworth, Sevenoaks, 1965.

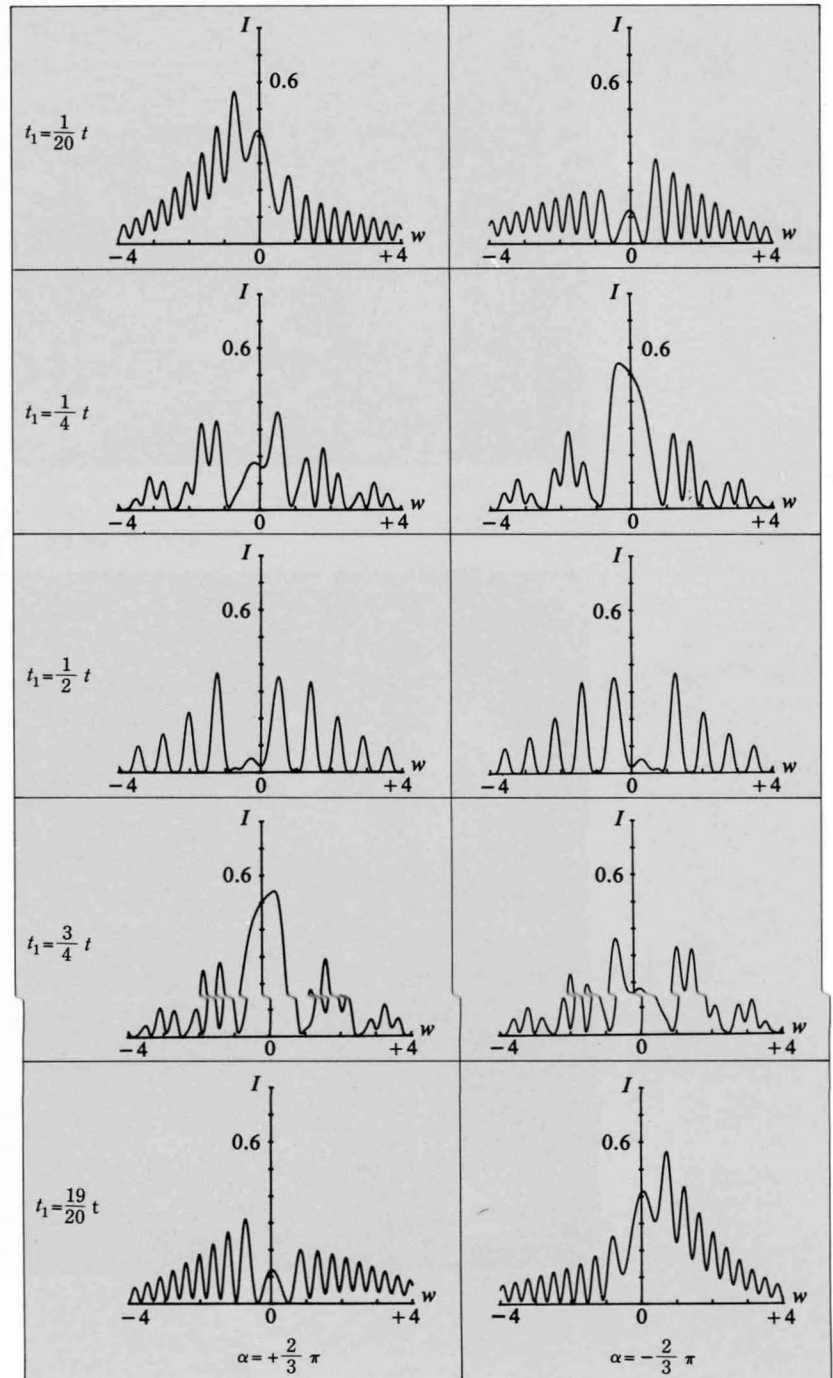


## Determination of $\alpha = 2\pi\mathbf{g}\cdot\mathbf{R}$ using ZOLZ reflections

Rocking curves of a low-order ZOLZ reflection were calculated by the two beam dynamical theory. Thickness  $t$  was assumed as  $t/\xi_g = 4$  in accordance with usual experimental conditions, where  $\xi_g$  is the extinction distance (e.g.  $\xi_g = 30\text{nm}$ ,  $t = 120\text{nm}$ ). The absorption distances  $\xi'_g$  and  $\xi'_o$  were given as  $\xi_g/\xi'_g = 1/20$  and  $\xi'_o = \xi'_g$  throughout this section. Figure (a) shows a rocking curve of a reflection for a perfect crystal, which is symmetric with respect to the exact Bragg position  $w = 0$ . Figure (b) shows rocking curves of a reflection for a crystal containing a stacking fault. The curves in the left column were calculated for  $\alpha = 2\pi\mathbf{g}\cdot\mathbf{R} = +(2/3)\pi$  and those in the right column for  $\alpha = -(2/3)\pi$ . All the curves are no longer symmetric about  $w = 0$ . The curves for  $\alpha = +(2/3)\pi$  and those for  $\alpha = -(2/3)\pi$  show opposite sense asymmetries to each other. That is, for example, the curve for  $\alpha = +(2/3)\pi$  and  $t_1 = (1/20)t$  is identical with that for  $\alpha = -(2/3)\pi$  and  $t_1 = (19/20)t$ , provided that the sign of  $w$  is reversed between the two curves. This relation is fully interpreted by the reciprocity theorem. For  $\alpha = +(2/3)\pi$ , the diffracted intensity for  $w < 0$  is stronger than that for  $w > 0$ . For  $\alpha = -(2/3)\pi$ , the intensity for  $w > 0$  is stronger than that for  $w < 0$ . The senses of asymmetry of the profiles obtained from near the top and bottom surfaces are distinguishable, while the asymmetries of other profiles are not clear.



(a) Dark-field rocking curve for a perfect crystal at  $t/\xi_g = 4$

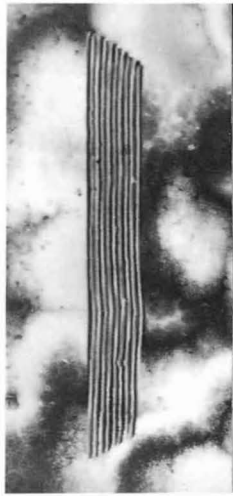


(b) Dependence of dark-field rocking curve for a stacking fault on  $t_1$

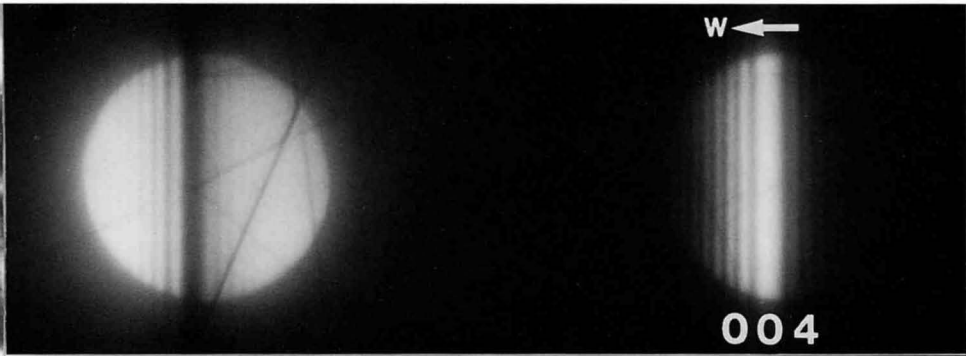
Si [110]

Top or bottom

200 kV



1 μm



(a)



(b)

$$\alpha = -\frac{2}{3}\pi$$

Bottom or top

$$\alpha = +\frac{2}{3}\pi$$



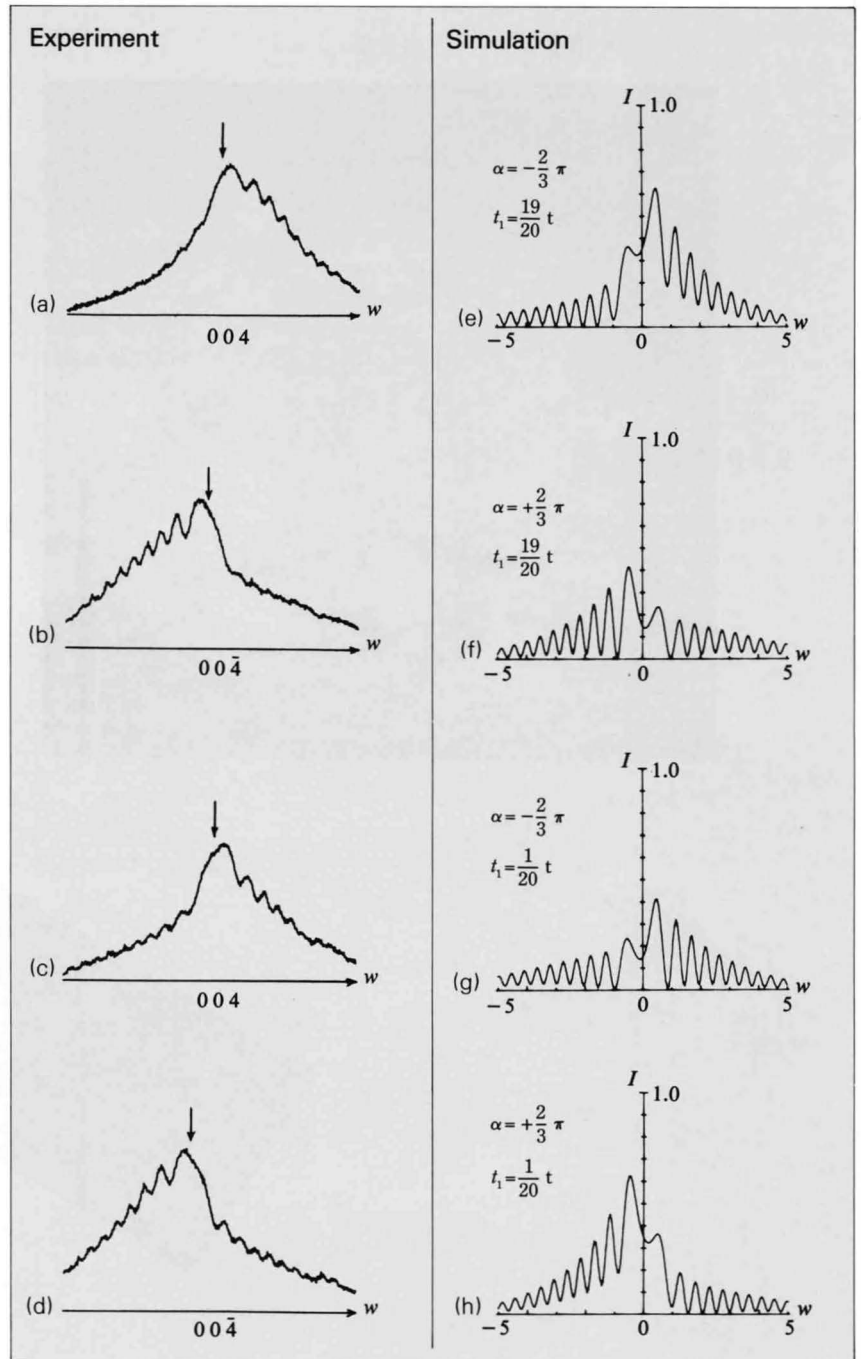
(c)



(d)

Stacking faults of Si were formed by annealing bulk specimens at 1050°C for 10 days. Photographs (a) and (b) were taken from near the left edge of the stacking fault seen in an attached electron micrograph of (110) Si at the 004 and 00 $\bar{4}$  exact Bragg settings, respectively. Photographs (c) and (d) were taken from near the right edge of the fault. Figures (a), (b), (c) and (d) show microdensitometer curves of the diffracted intensities in Photos (a), (b), (c) and (d), respectively, and show a qualitatively good agreement with the calculated curves (e), (f), (g) and (h), respectively. The sign of  $\alpha$  was determined to be negative or  $-(2/3)\pi$  for the 004 reflection. Since displacement vectors  $\mathbf{R}$  allowed for a stacking fault oblique to the (110) surface are  $1/3[11\bar{1}]$ ,  $1/3[\bar{1}\bar{1}1]$ ,  $1/3[\bar{1}\bar{1}\bar{1}]$  and  $1/3[111]$ , a possible  $\mathbf{R}$  is  $1/3[\bar{1}\bar{1}\bar{1}]$  or  $1/3[11\bar{1}]$ . To determine which vector is the correct one, it is necessary to know whether the faulted plane is a  $(\bar{1}\bar{1}\bar{1})$  plane or  $(11\bar{1})$  plane. (see pages 148 and 149)

The Si specimens containing stacking faults were supplied by Dr. I. Yonenaga and Prof. K. Sumino of the Research Institute for Iron, Steel and Other Metals, Tohoku University.



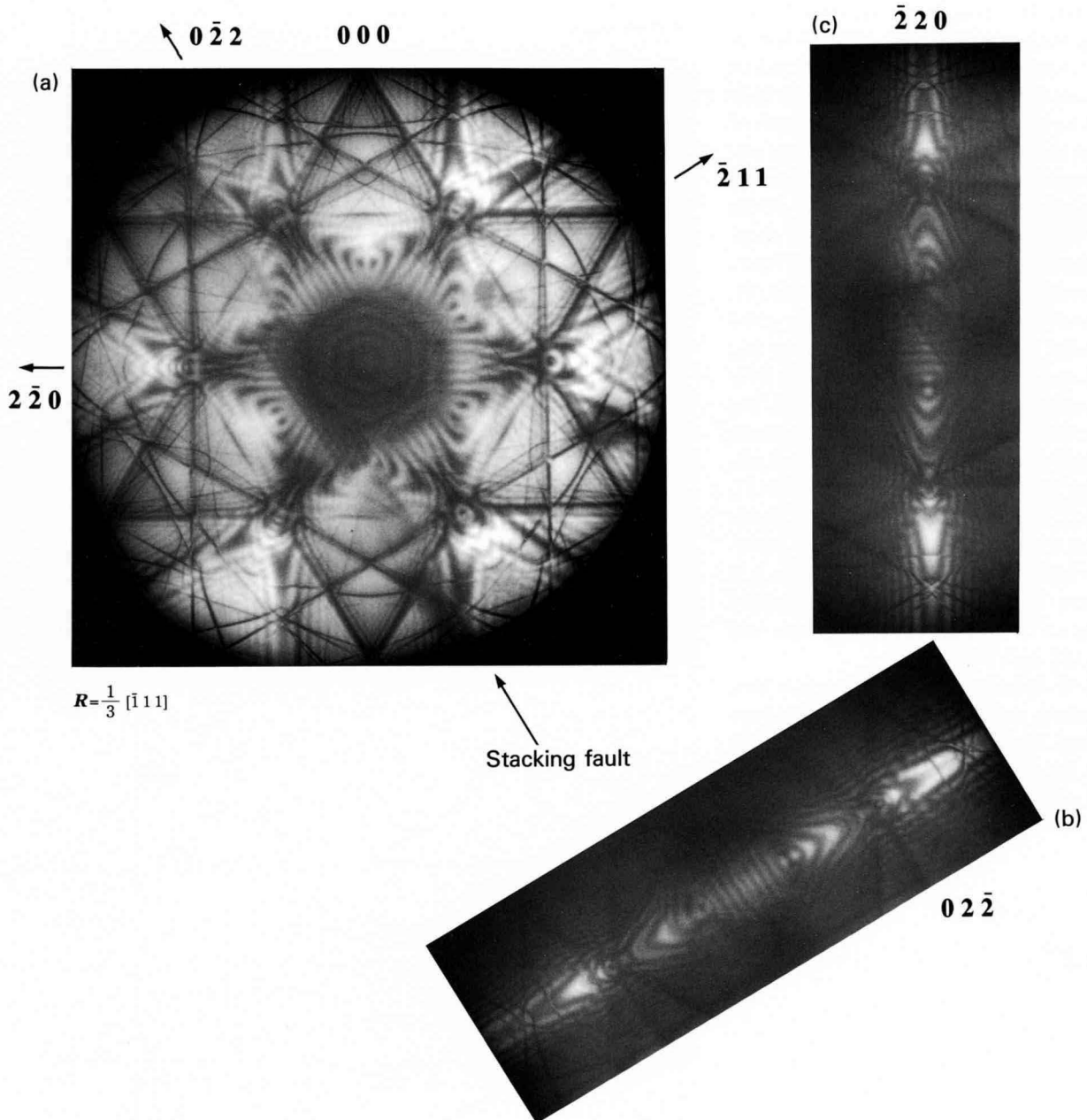
Microdensitometer charts of dark-field disks. Arrows indicate Bragg position.

Calculated rocking curves at  $t=400$  nm and  $\xi_g = 166.6$  nm.

# Observation of stacking faults using LACBED

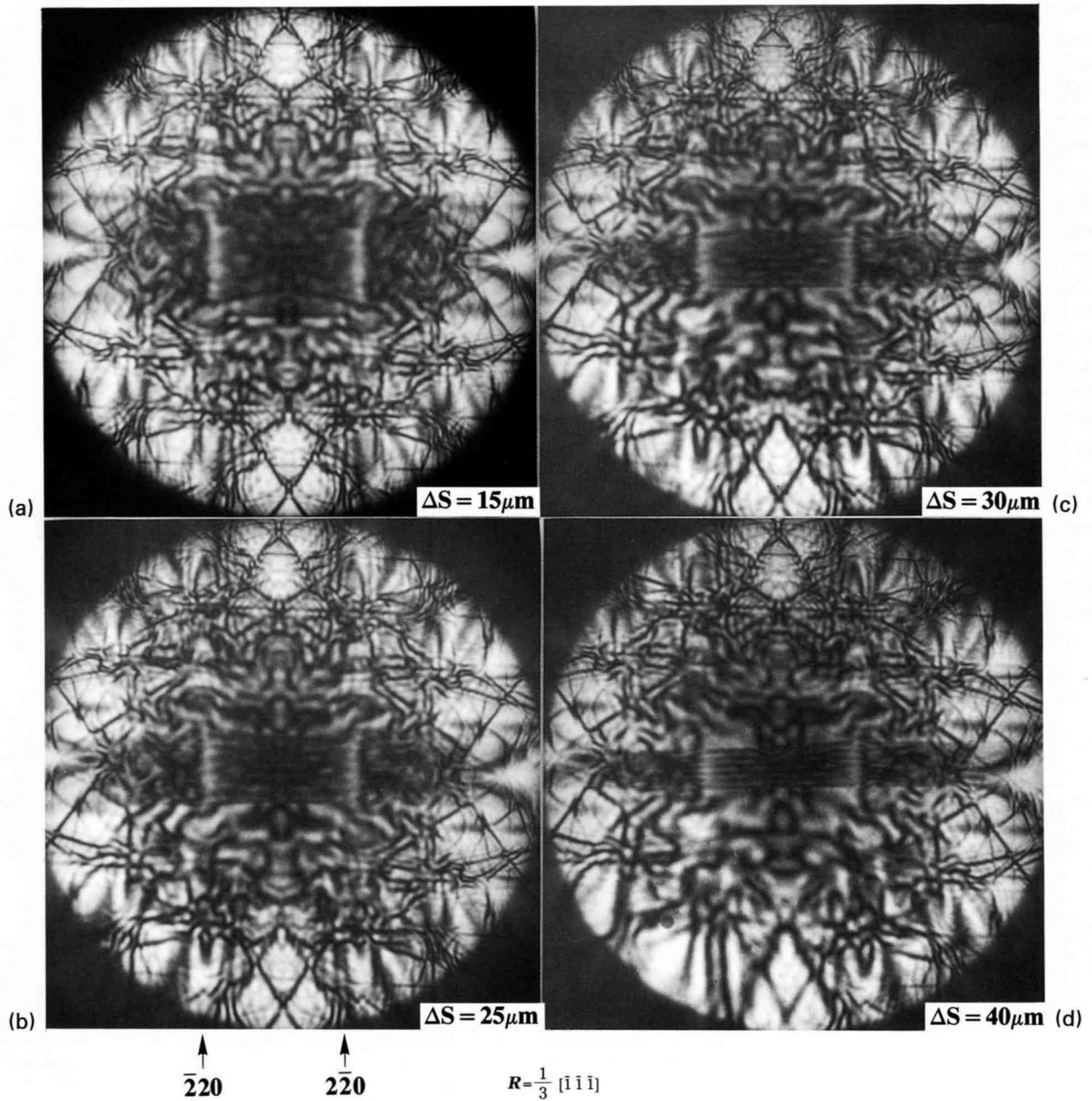
Si [111]

100 kV



Photographs (a), (b) and (c) show LACBED patterns of a (111) Si film containing a stacking fault with a displacement vector  $\mathbf{R}$  of the  $1/3\langle 111 \rangle$  type. In Photo (a), the image of the stacking fault, indicated by an arrow, and the CBED pattern are simultaneously recorded. As a result, the orientation of the fault is unambiguously identified. At the  $02\bar{2}$  Bragg position, where  $\alpha = 2\pi\mathbf{g}\cdot\mathbf{R} = 0$ , the fault is seen to have lost its contrast. The same information is obtained from dark-field LACBED patterns. In the  $02\bar{2}$  pattern (b), the fault has lost the contrast because of  $\alpha = 0$ , whereas in the  $\bar{2}20$  pattern (c) it shows

a definite contrast. The fact that  $\alpha = 0$  for  $\mathbf{g} = 02\bar{2}$  allows us to select the possible vectors of  $\mathbf{R}$  to be  $1/3[1\bar{1}\bar{1}]$ ,  $1/3[\bar{1}11]$ ,  $1/3[111]$  and  $1/3[\bar{1}\bar{1}\bar{1}]$ . Since the fault is tilted to the specimen surface, the vectors  $1/3[111]$  and  $1/3[\bar{1}\bar{1}\bar{1}]$  are rejected. The displacement vector  $\mathbf{R}$  is determined as  $1/3[1\bar{1}\bar{1}]$  or  $1/3[\bar{1}11]$ . The sign of the vector is left undetermined.



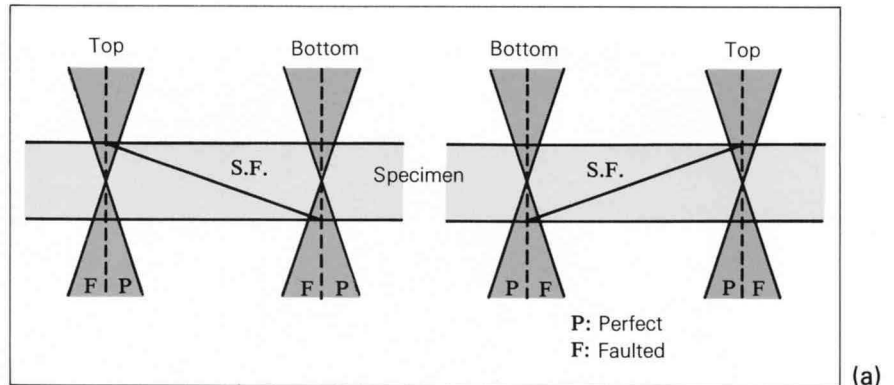
Photographs (a), (b), (c) and (d) show LACBED patterns taken from a (110) Si film containing a stacking fault of  $R = 1/3[\bar{1}\bar{1}\bar{1}]$  at defocus  $\Delta S = 15, 25, 30$  and  $40\mu\text{m}$ , respectively. When the amount of defocus is small, the fault is largely magnified. (In-focus CBED patterns, therefore, are regarded as images with a magnification of infinity.) The pattern due to the fault is difficult to recognize

as an image (a), but the loss of a symmetry due to the fault is easily seen. With larger defocuses (c) and (d), the fault becomes to be seen as a usual microscope image, but the change of the symmetry on the fault is difficult to see. It is noted that the deterioration of the pattern is seen owing to the thickness variation in the illuminated specimen area.

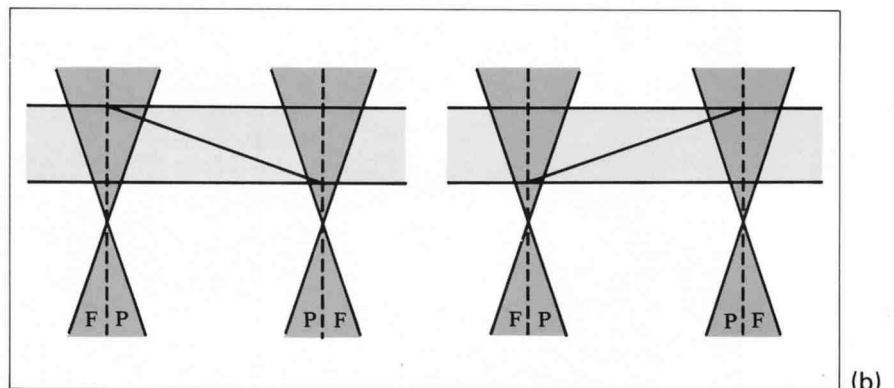
## Determination of the top and bottom of a stacking fault CBED patterns from the edges of a stacking fault

The sense of tilt of a stacking fault can be determined by a simple CBED technique. One half of the incident beam illuminates the fault and the other half illuminates a perfect specimen area. Then, a half of the bright-field CBED pattern is affected by the fault and the other half is not. The expected results are illustrated in the diagrams for two senses of tilt of the fault and for three different focuses; (a) in-focus, (b) under-focus and (c) over-focus. The letters F and P indicate a faulted and a perfect pattern. These results are summarized in the table.

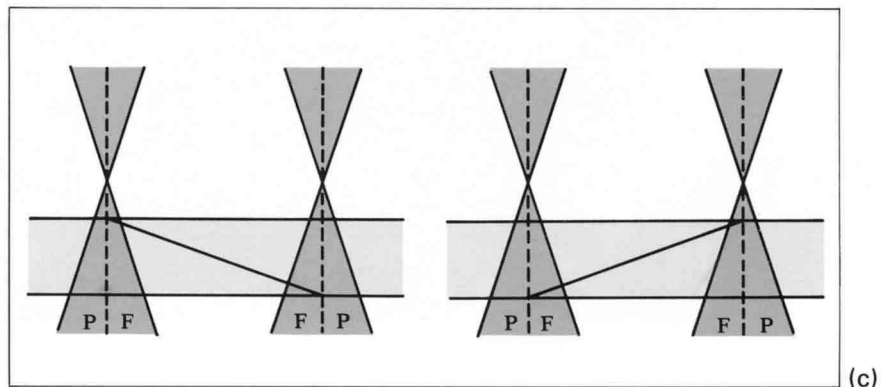
Photographs (c), (e) and (g) were taken from edge A of the fault in Photo (a) at the three different focuses. Photographs (d), (f) and (h) were taken from edge B at the three different focuses. Referring to the diagrams and the table, edge A was determined to be at the top surface and edge B at the bottom surface.



Incident beam is focused in the specimen (in-focus).



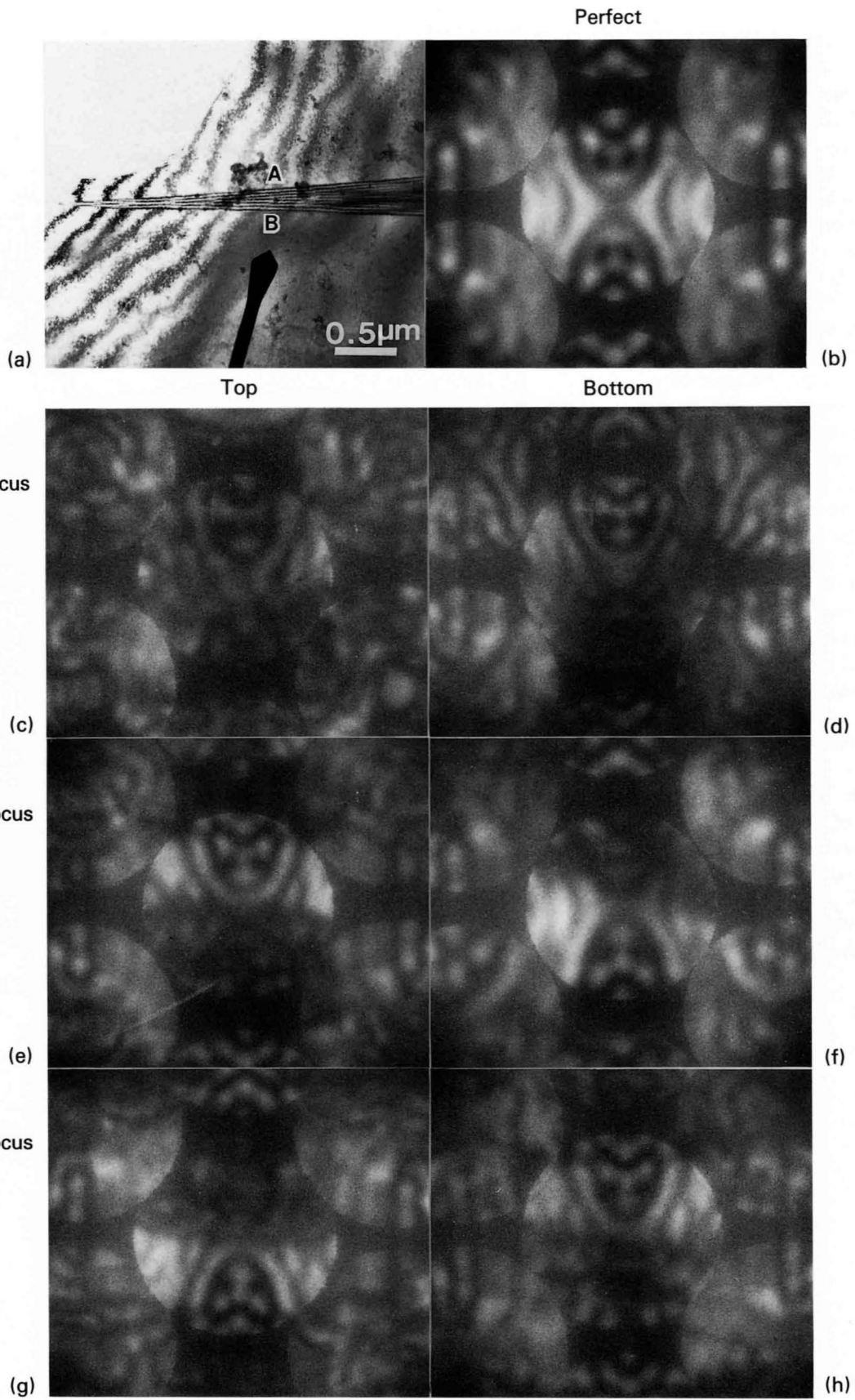
Incident beam is focused below the specimen (under-focus).



Incident beam is focused above the specimen (over-focus).

Focus	Downward Tilt		Upward Tilt	
	Top	Bottom	Bottom	Top
In-focus	FP	FP	PF	PF
Under-focus	FP	PF	FP	PF
Over-focus	PF	FP	PF	FP

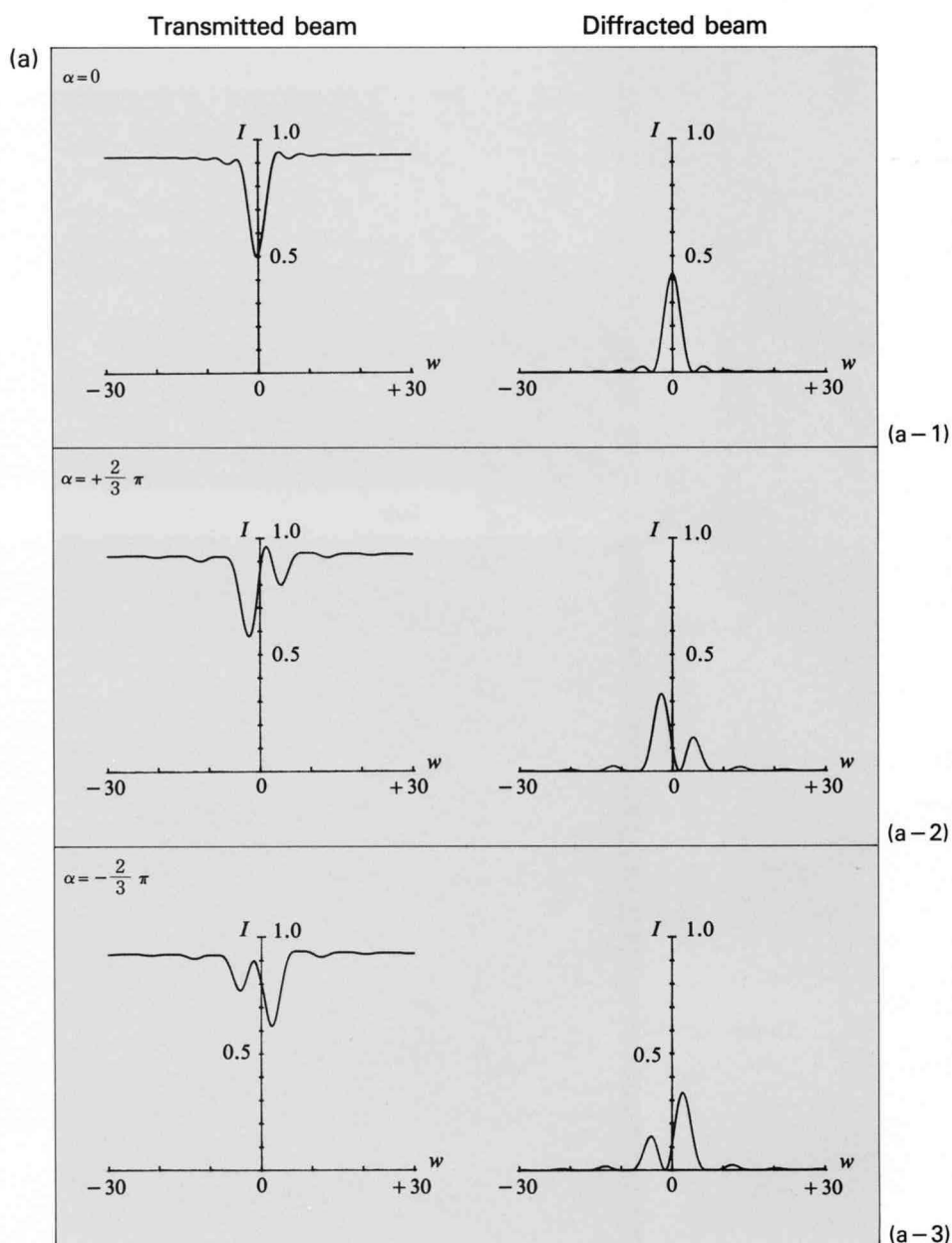
Si [110]



## Determination of the displacement vector $R$ using HOLZ reflections

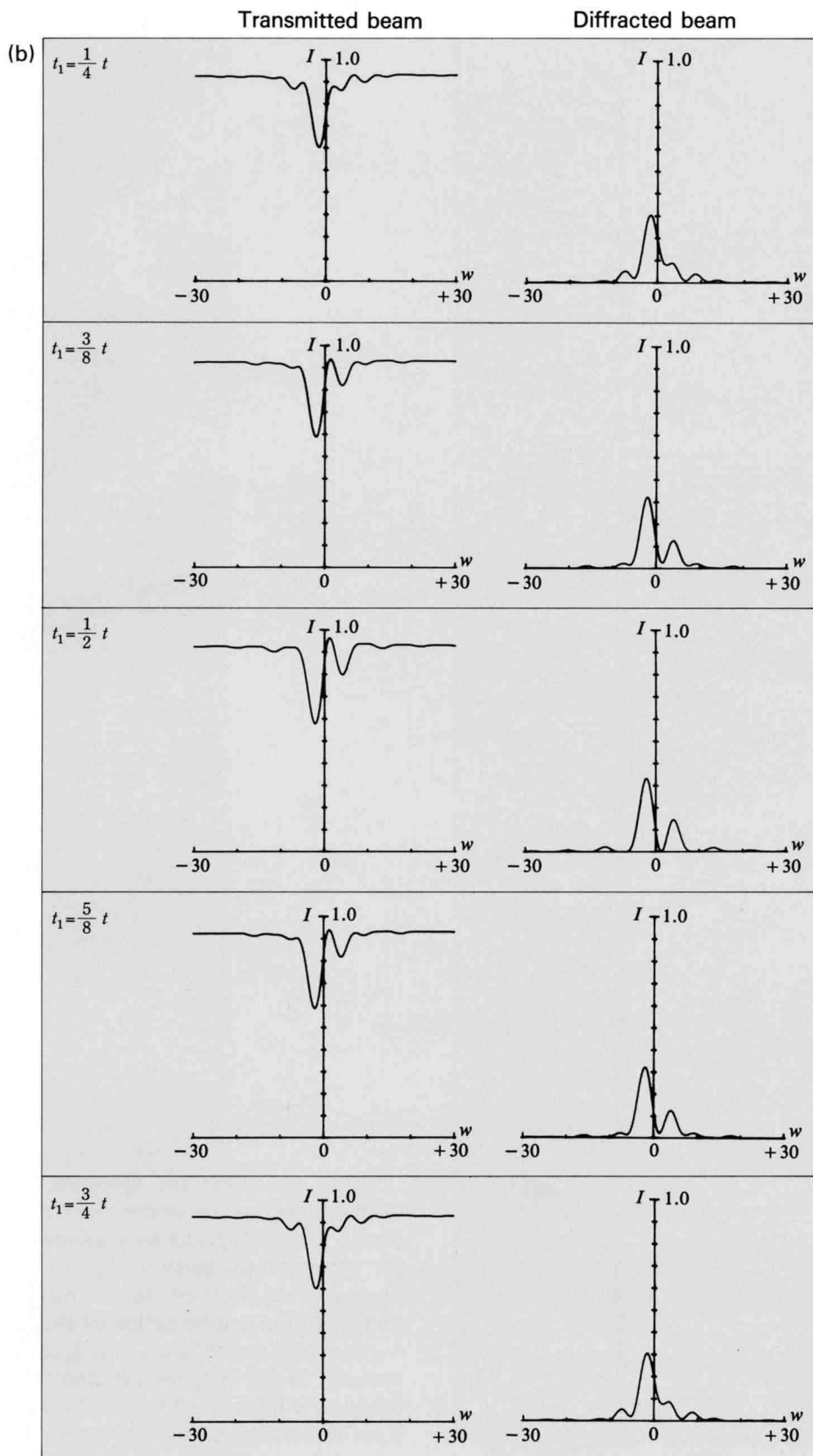
Rocking curves were calculated for a HOLZ reflection by the two-beam dynamical theory. Thickness  $t$  was assumed as  $t/\xi_g = 1/4.25$  (e.g.  $t = 100$  nm and  $\xi_g = 425$  nm) by considering usual experimental conditions. Figure (a) shows three pairs of rocking curves of the transmitted beam and a diffracted beam for  $\alpha = 0$ ,  $+(2/3)\pi$  and  $-(2/3)\pi$  at  $t_1 = (1/2)t$ . The curve of the dark-field pattern for  $\alpha = 0$  is symmetric about  $w = 0$ , and the curve of the bright-field pattern is almost symmetric, because of a small anomalous absorption effect. The principal peak of the curves are split into two peaks when  $\alpha = \pm(2/3)\pi$ . For  $\alpha = -(2/3)\pi$ , the peak intensity at  $w > 0$  is larger than that at  $w < 0$ . For  $\alpha = +(2/3)\pi$ , the peak intensity at  $w < 0$  is larger than that at  $w > 0$ . (The two peaks are expected to be the same for  $\alpha = (1/2)\pi$ .) The sense of asymmetry between the two peaks is characteristic of the sign of  $\alpha$ , which permits the determination of the displacement vector.

It should be noted that the asymmetry of the peaks does not originate from the anomalous absorption effect but from the redistribution of the Bloch waves on two branches of the dispersion surface at the fault.



Calculated rocking curves at  $\frac{t}{\xi_g} = \frac{1}{4.25}$  and  $t_1 = \frac{1}{2}t$

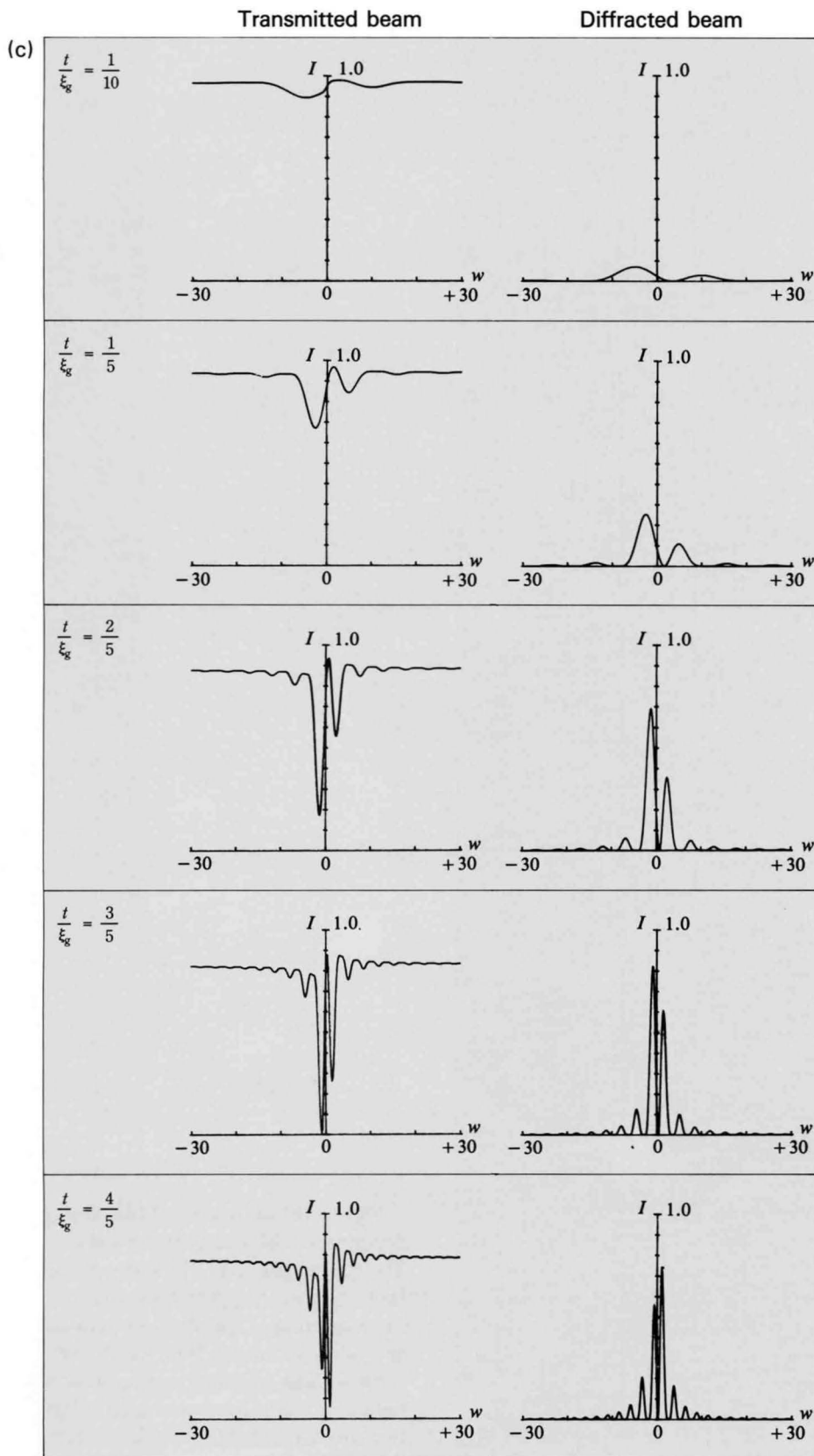
## Dependence on the depth of a stacking fault



Calculated rocking curves at  $\frac{t}{\xi_g} = \frac{1}{4.25}$  for  $\alpha = +\frac{2}{3}\pi$

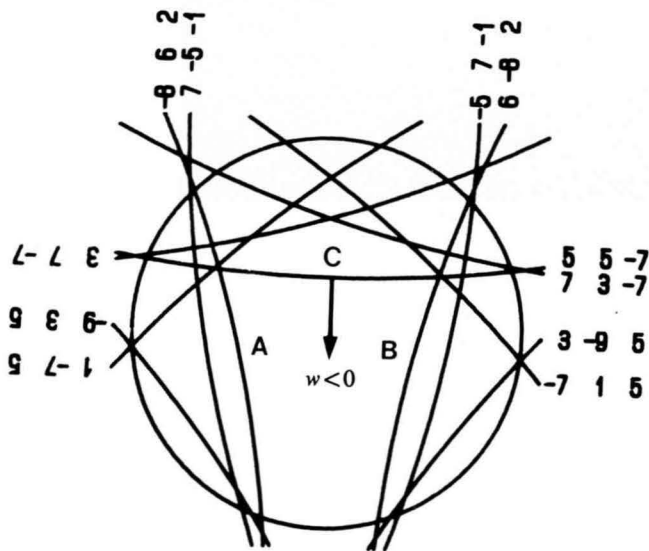
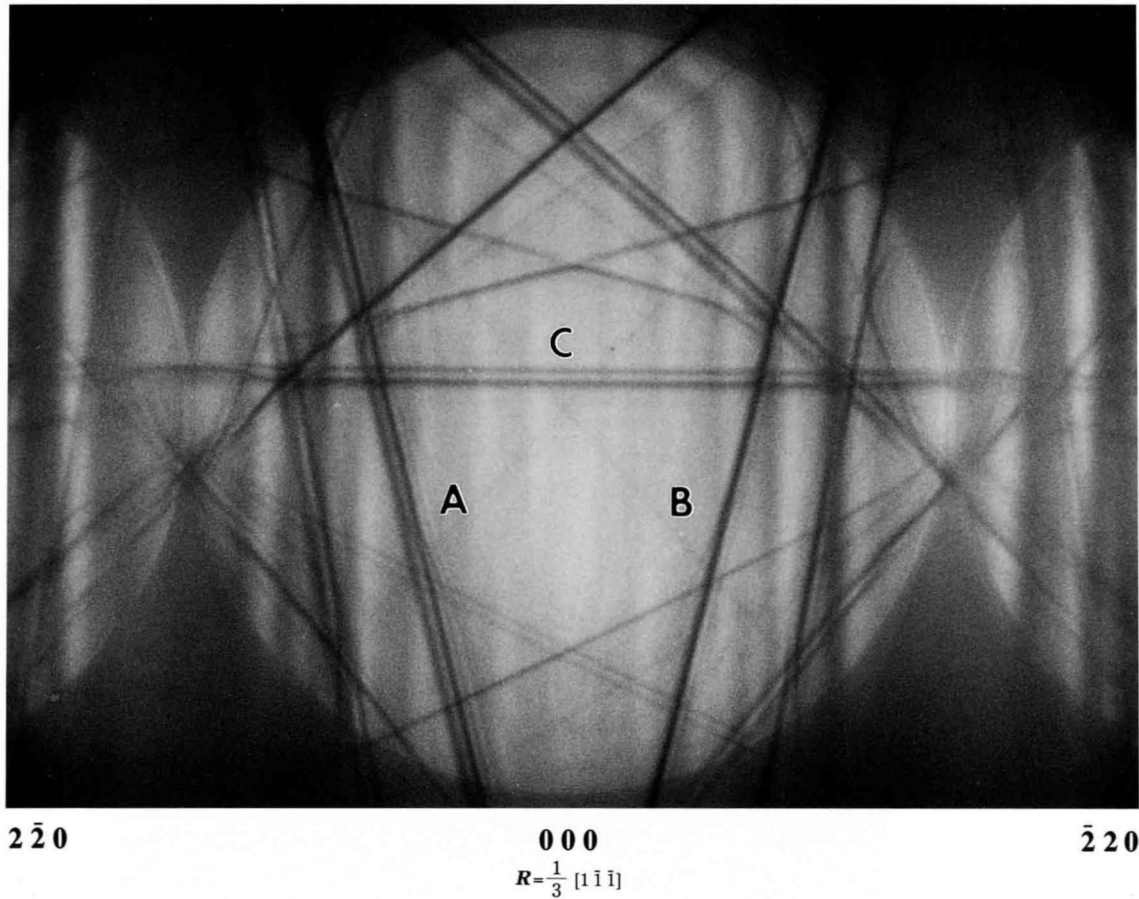
Figure (b) shows the fault-depth dependence of the rocking curves. The curves obtained at depths of the fault  $(3/8)t \leq t_1 \leq (5/8)t$  show a definite splitting of the peak. The curves at  $t_1 < (3/8)t$  and  $t_1 > (5/8)t$  do not show a clear splitting and approach the curve for a perfect crystal. This fact indicates that the incident beam needs to illuminate a position around the middle of the fault to identify the fault.

## Dependence on specimen thickness



Calculated rocking curves at  $t_1 = \frac{1}{2} t$  for  $\alpha = +\frac{2}{3} \pi$

Figure (c) shows the specimen-thickness dependence of the rocking curves. Two clear peaks are obtained for specimen thickness  $t/\xi_g \leq 3/5$ . This condition places no practical restriction to the determination of the displacement vector. That is, if  $\xi_g$  is assumed as 500 nm, the maximum thickness to be used is 300 nm, which is sufficiently thick for usual experiments. There is no restriction to thin specimens, in contrast to the electron-microscope-image method.



The photograph was taken at the [334] incidence from (111) Si containing a stacking fault with  $R = 1/3[1\bar{1}\bar{1}]$ . A simulation of HOLZ line geometry obtained by an arc (circle) approximation is shown, which provides an easy identification of the sign of excitation error  $w$ . The sign of  $w$  is positive inside arcs and negative outside them. From the simulation, the HOLZ lines A, B and C in the photograph are indexed as  $\bar{8}62$ ,  $6\bar{8}2$  and  $5\bar{5}7$ . The values of  $\alpha$  for the three reflections are  $-(2/3)\pi$ ,  $0$ ,  $+(2/3)\pi$ . The HOLZ line profiles A, B and C show a good agreement with the calculated curves for  $\alpha = -(2/3)\pi$ ,  $0$ ,  $+(2/3)\pi$  (Fig. (a) on page 150), respectively.

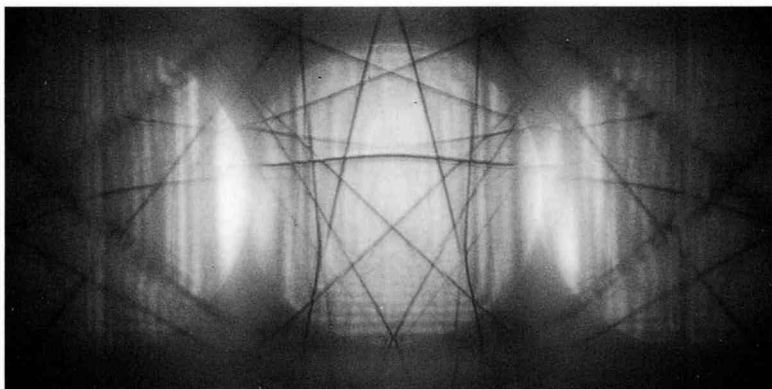
Since the values of  $\alpha$  including their signs can be determined for plural HOLZ lines, the displacement vector can uniquely be identified by the present method.

## Dependence on stacking fault depth (experimental)

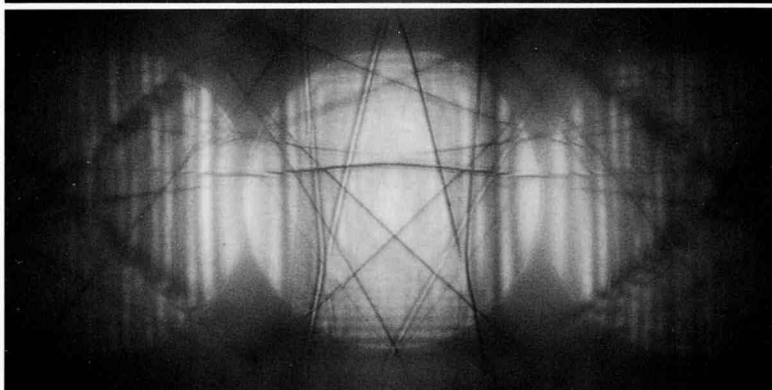
Si [332]

80 kV

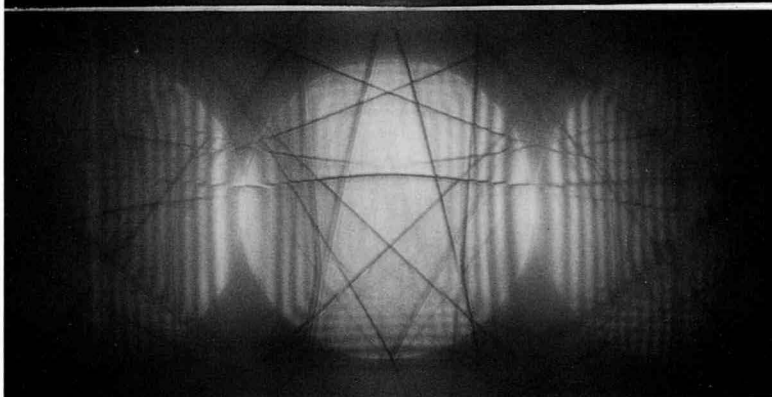
Near top



Middle



Near bottom



$$R = \frac{1}{3} [\bar{1} \bar{1} \bar{1}]$$

HOLZ lines obtained from the middle of a stacking fault exhibit the best splitting, showing a good agreement with the theoretical prediction.

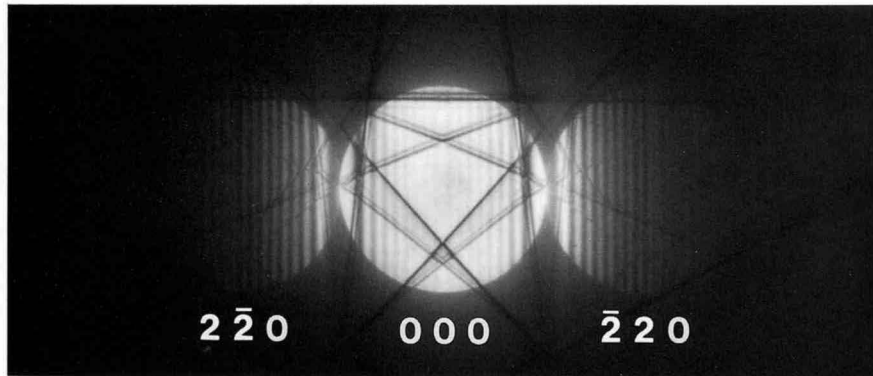
**Hollow-cone beam technique**

Si [331]

100 kV

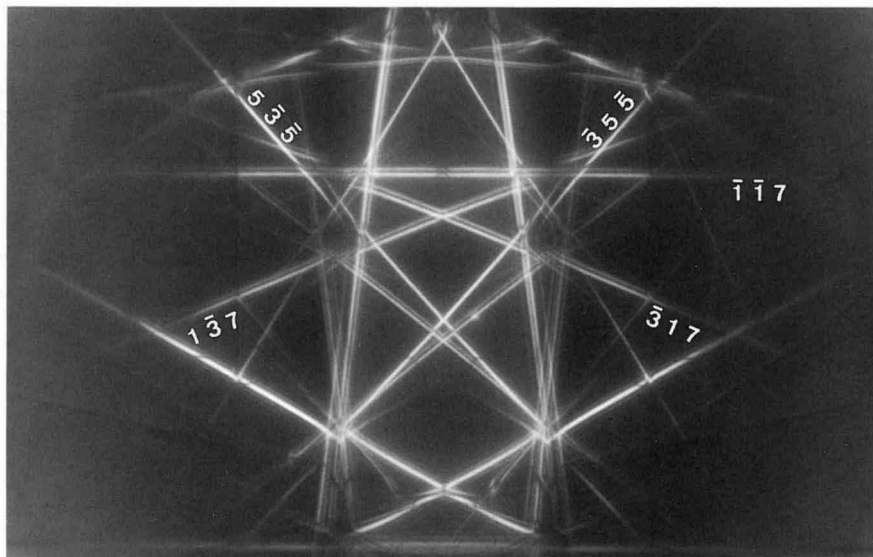
Ordinary CBED pattern

Stacking fault

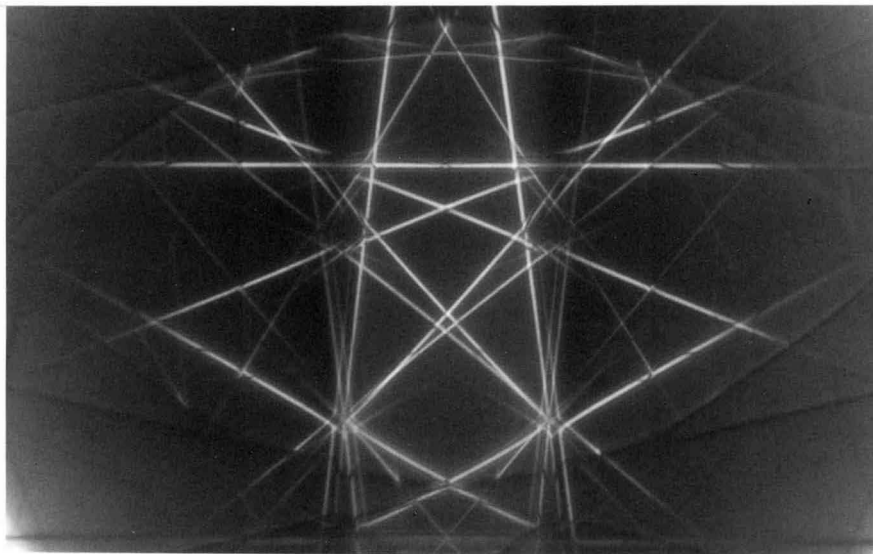


Hollow-cone beam pattern

Stacking fault



Perfect crystal



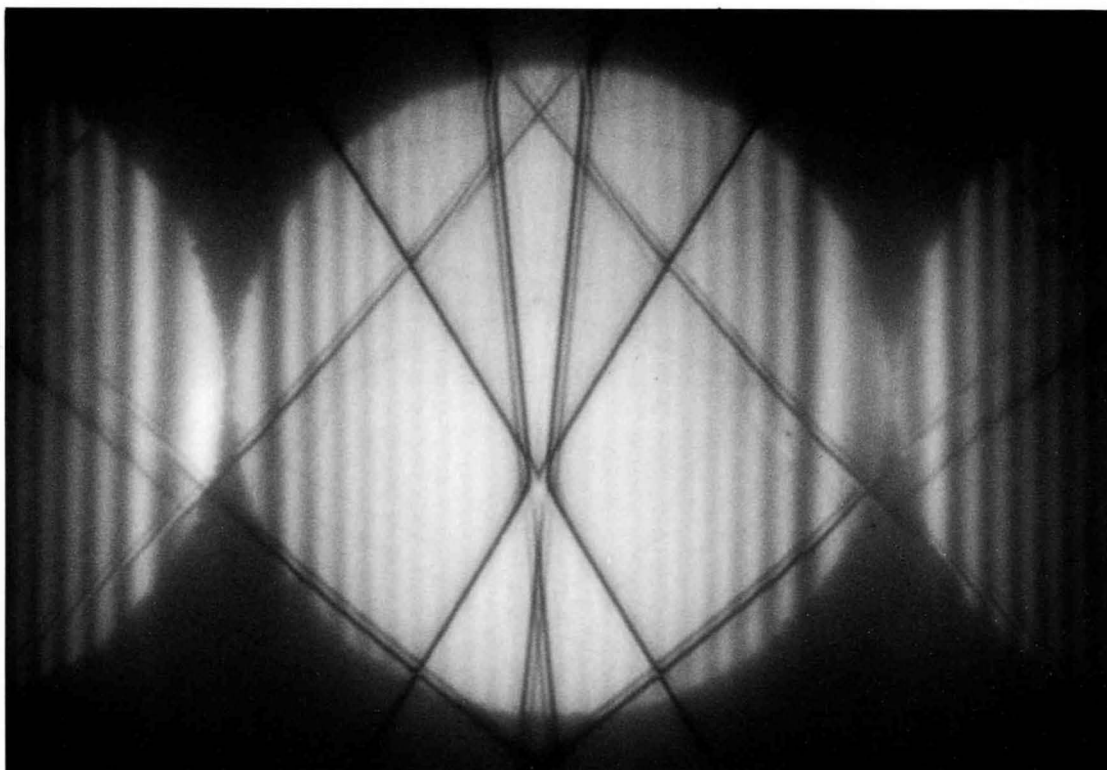
$$R = \frac{1}{3} [\bar{1} \bar{1} \bar{1}]$$

The hollow-cone beam technique makes the splitting of HOLZ lines clear over a wide angular range without strong background due to ZOLZ reflections.

## Determination of displacement vectors of stacking faults

1) Si [331]

200 kV

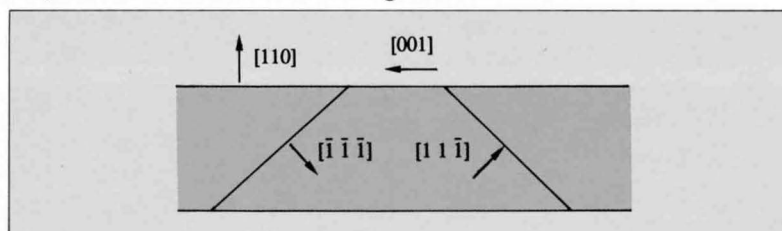


$\bar{2}20$

000

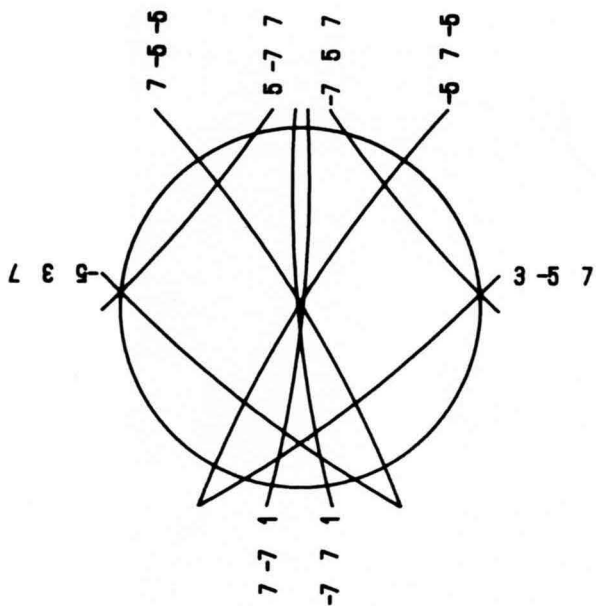
$2\bar{2}0$

Displacement vectors of stacking faults in Si



Geometrically allowed displacement vectors  $R$

$$R = \frac{1}{3} [111], \frac{1}{3} [\bar{1}\bar{1}\bar{1}], \frac{1}{3} [\bar{1}\bar{1}1], \frac{1}{3} [11\bar{1}]$$



The bright-field pattern was taken from a (110) Si film containing a stacking fault at the [331] incidence and at an accelerating voltage of 200 kV. From the computer simulation, the observed HOLZ lines were indexed and the sign of  $w$  was determined for each line. It is seen that the  $7\bar{5}\bar{5}$  and  $\bar{5}7\bar{5}$  lines remain unsplit but the other lines are split. Allowed displacement vectors are given in the attached figure. The table lists experimental values of  $\alpha$  for the eight reflections. The letter Y is given when the value of  $\alpha$  calculated using a possible displacement vector agrees with the experimental value. The letter N is given when it does not agree.

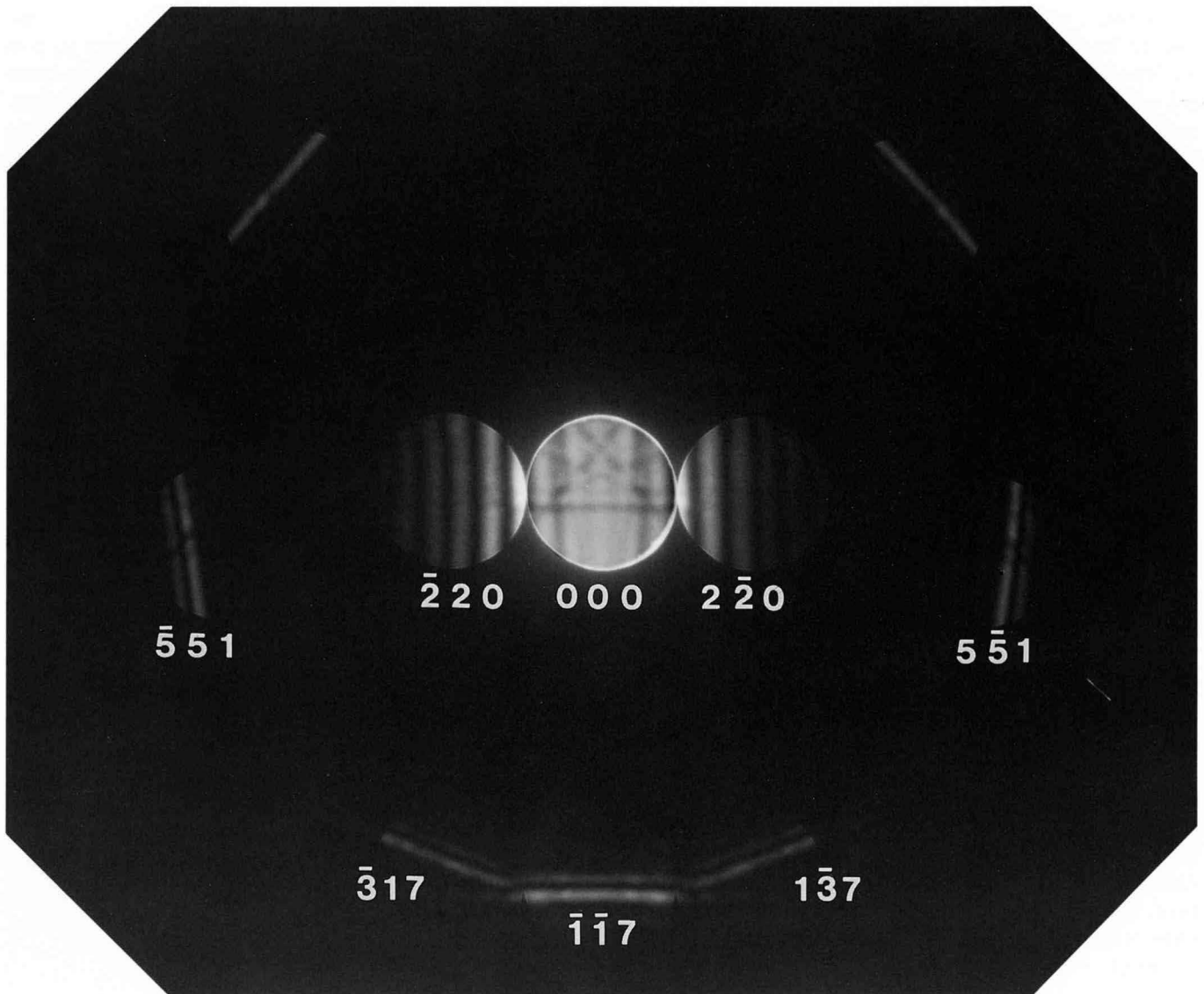
$g$	$\alpha(\text{exp.})$	$\frac{1}{3}[111]$	$\frac{1}{3}[\bar{1}\bar{1}\bar{1}]$	$\frac{1}{3}[11\bar{1}]$	$\frac{1}{3}[\bar{1}\bar{1}1]$
$7\bar{7}1$	$-\frac{2}{3}\pi$	N	Y	Y	N
$\bar{7}71$	$-\frac{2}{3}\pi$	N	Y	Y	N
$\bar{5}\bar{7}\bar{5}$	0	Y	Y	N	N
$7\bar{5}\bar{5}$	0	Y	Y	N	N
$\bar{5}37$	$+\frac{2}{3}\pi$	N	Y	N	N
$3\bar{5}7$	$+\frac{2}{3}\pi$	N	Y	N	N
$5\bar{7}7$	$+\frac{2}{3}\pi$	N	Y	N	N
$\bar{7}57$	$+\frac{2}{3}\pi$	N	Y	N	N



Thin specimen

Si [331]

80 kV



The CBED pattern was taken from a thin (about 40 nm) specimen area of (110) Si containing a stacking fault. The splittings of lines in HOLZ reflections are clearly seen. Note that the electron-microscope-image method does not allow easy identification of the displacement vector of a fault in such a thin specimen.

# Dislocations

Carpenter and Spence [20] reported a method to identify the Burgers vector  $\mathbf{b}$  of a dislocation. They observed additional fringes in intensity profiles of reflections with  $\mathbf{g}\cdot\mathbf{b}\neq 0$ . They determined the vector  $\mathbf{b}$  by finding a profile undisturbed by a dislocation or a reflection with  $\mathbf{g}\cdot\mathbf{b}=0$ . Cherns and Preston [23] have proposed an excellent method to determine the Burgers vector of a dislocation, in which the whole strain field of the dislocation is illuminated by a defocus convergent beam. When the incident beam illuminates a small specimen area around a dislocation, only the effect of local strain of the dislocation is observed. Defocus illumination or LACBED allows observing the whole strained area and identifying the Burgers vector. A defocus CBED pattern gives the intensity profile of a reflection as functions of the distance from a dislocation  $x$  and of excitation error  $w$ . The method [23] can use information obtained not only at  $\mathbf{g}\cdot\mathbf{b}=0$  but also at  $\mathbf{g}\cdot\mathbf{b}=n$  ( $n\neq 0$ ) for Burgers vector determination, while information obtained at  $\mathbf{g}\cdot\mathbf{b}\neq 0$  has been discarded in the traditional electron-microscope-image method except a few reports [a]. A defocus CBED pattern shows  $n$  nodes at the crossing region between a dislocation line and a reflection line when  $\mathbf{g}\cdot\mathbf{b}=n$ . The following studies of dislocations have fully been based upon their method. It should be emphasized that the relative sign of  $\mathbf{g}\cdot\mathbf{b}=n$  is important for Burgers vector identification.

Figure (a) illustrates two defocus CBED modes. We adopt the left mode because the sense of an object shown by the arrow  $X$  is the same as that of a defocus CBED pattern (image) as shown by the arrows  $X_o$  and  $X_g$ . Figure (b) shows the side view of a specimen containing a dislocation and a column through which the electron beam runs. The atomic displacement  $\mathbf{R}$  due to a general perfect dislocation in an infinite isotropic medium is written in the form

$$\mathbf{R} = \frac{1}{2\pi} [\mathbf{b}\Phi + \mathbf{b}_e \frac{\sin 2\Phi}{4(1-\nu)} + (\mathbf{b} \times \mathbf{u}) \{ \frac{1-2\nu}{2(1-\nu)} \ln r + \frac{\cos 2\Phi}{4(1-\nu)} \}] \quad (1)$$

where  $\mathbf{b}$  is the Burgers vector,  $\mathbf{b}_e$  is the edge component of  $\mathbf{b}$ ,  $\mathbf{u}$  is the unit vector of the dislocation line,  $r$  is the distance from the dislocation line,  $\nu$  is Poisson's ratio and  $\Phi = \phi - \gamma$ . The atomic displacement due to a pure screw dislocation is expressed simply by the equation

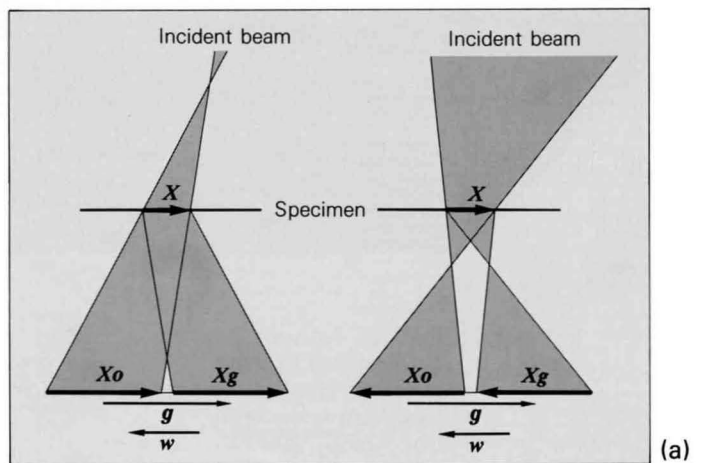
$$\mathbf{R} = \frac{\mathbf{b}}{2\pi} \Phi \quad (2)$$

## Reference

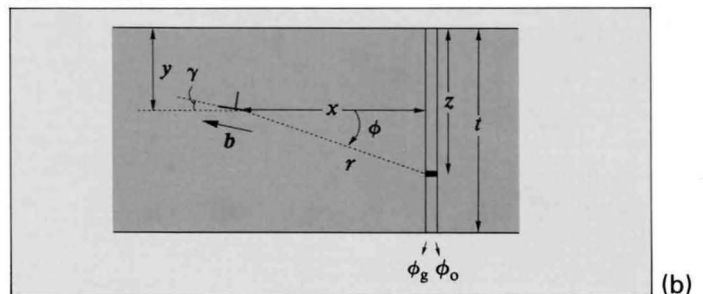
[a] Y. Ishida, H. Ishida, K. Kohra and H. Ichinose: *Phil. Mag.*, **42** (1980) 453.

Figure (c) shows defocus CBED patterns from an area containing a screw dislocation, computed by the two-beam dynamical theory using the Euler method for integration. The ratio between the thickness and extinction distance was given as  $t/\xi_g = 1/2$ . The dislocation was assumed to be at the middle of the specimen,  $y/t = 1/2$ . The absorption coefficients were assumed to be the same as those for stacking faults (see page 143). The ordinate and abscissa represent the excitation error  $w$  and the horizontal distance from the dislocation  $x/\xi_g$ . The dislocation lies parallel to the ordinate at  $x=0$ . A reflection line, the principal maximum of a reflection profile, lies parallel to the abscissa at  $w=0$  for a perfect crystal.

For  $\mathbf{g}\cdot\mathbf{b}=n=0$ , the reflection line appears as a straight line without the influence of the dislocation. For  $n=1$ , the reflection line deviates from  $w=0$  and splits into two lines near the dislocation, thus forming one node. For  $n=2$ , the reflection line splits into three, forming two nodes. When  $n$  is negative, the sense of deviation of the line from  $w=0$  is opposite to that of positive  $n$ . The defocus CBED patterns for  $n=1\sim 6$  are given on page 162. Since the lowest order reflection is often far from the condition  $t/\xi_g = 1/2$  for a specimen thickness usually used, it exhibits a complicated profile and is not suitable for Burgers vector determination.



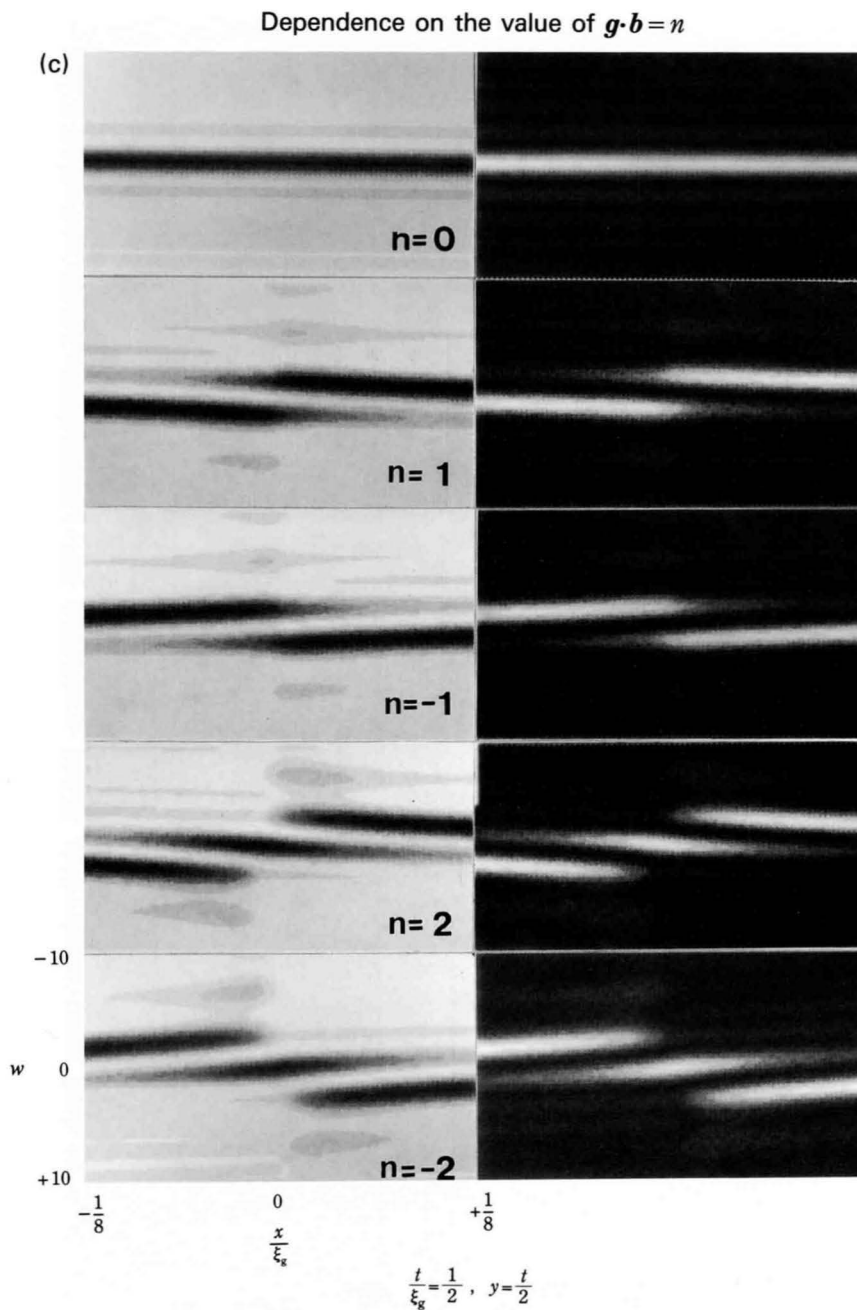
Two defocus CBED modes.



Crystal containing edge dislocation.

# Determination of Burgers vectors of perfect dislocations

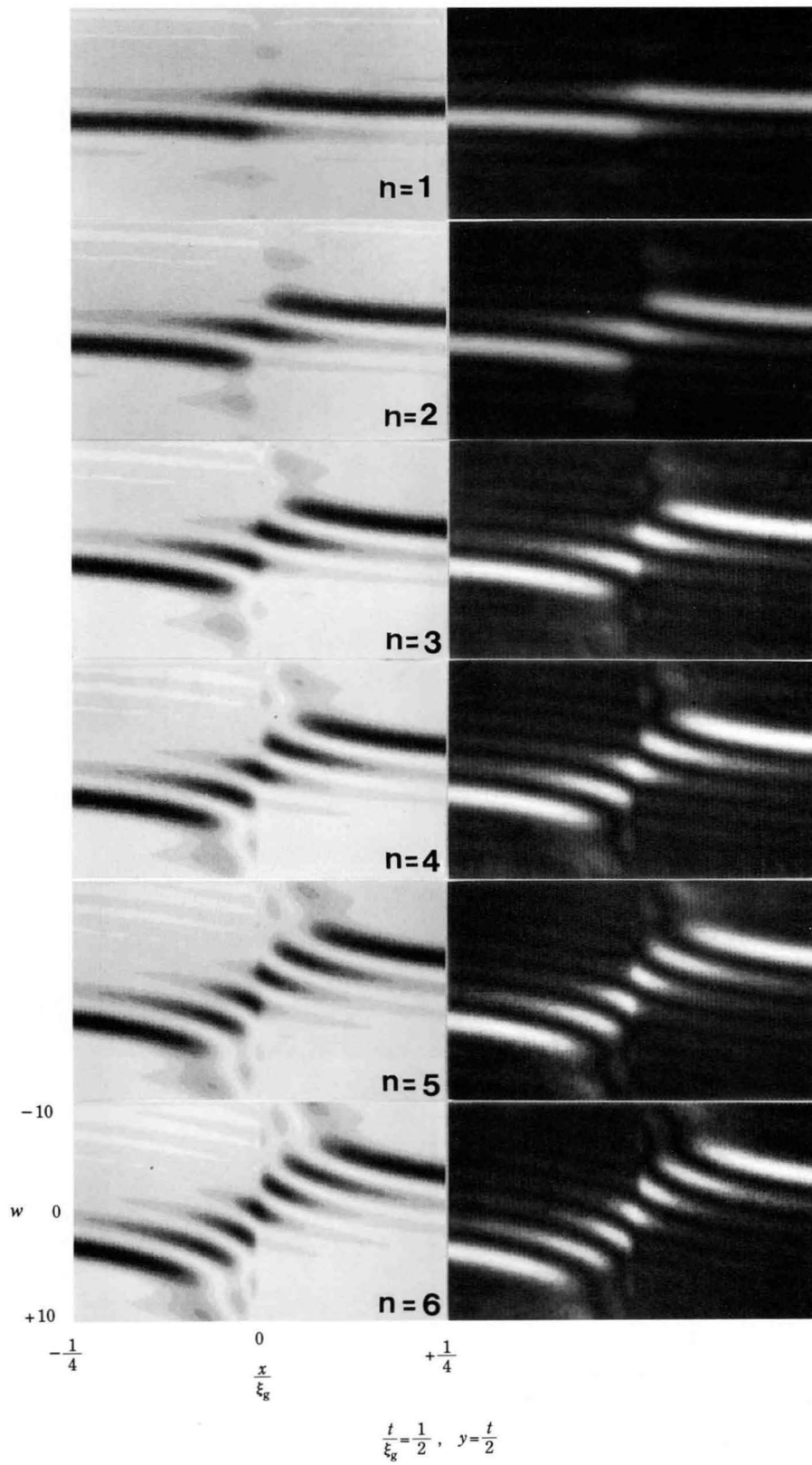
## Simulations of a reflection line crossing a screw dislocation



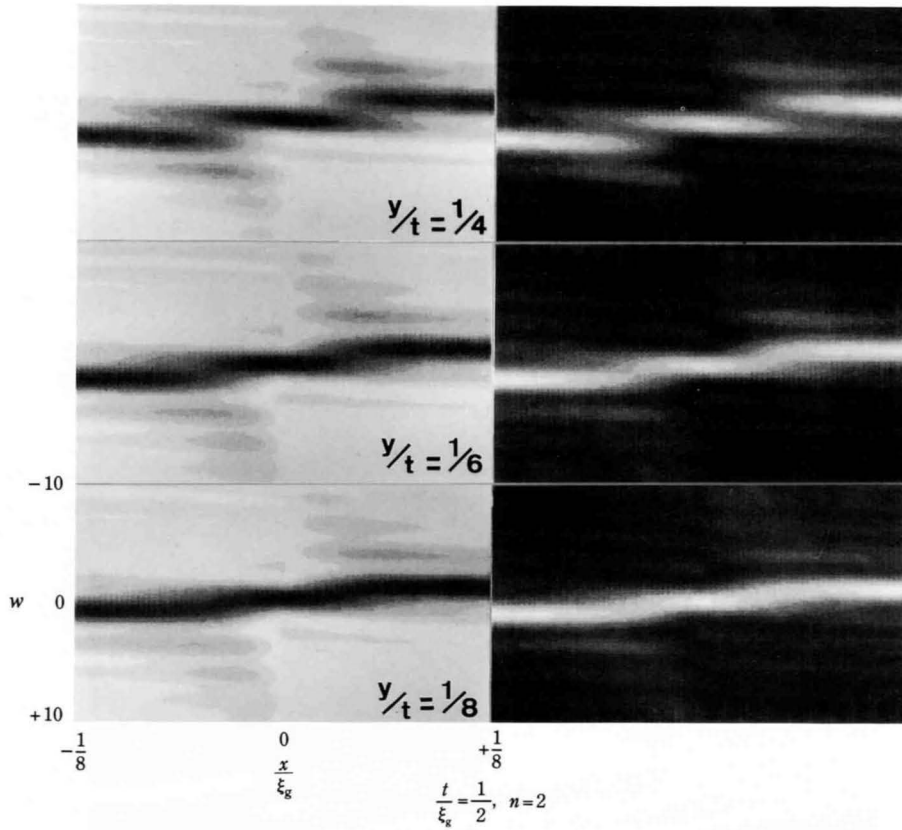
Left and right simulations are bright- and dark-field patterns, respectively.

# Simulations of a reflection line crossing a screw dislocation

Dependence on the value of  $g \cdot b = n$



Dependence on dislocation depth

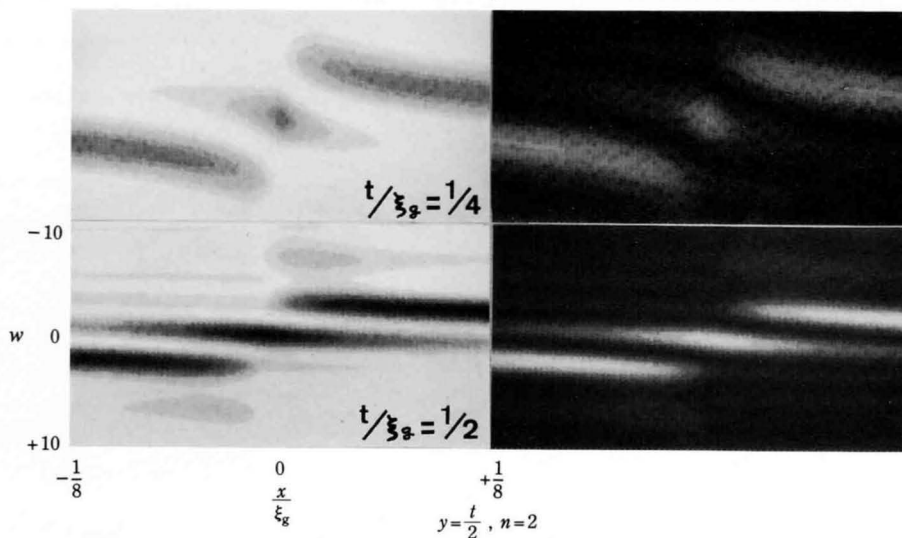


When a dislocation lies in the middle of a specimen, the splitting of a reflection line is seen best. The splitting is still clearly seen at a dislocation depth,  $y/t = 1/4$ , but becomes difficult to see at  $y/t = 1/6$ . This behaviour is analogous to that of a HOLZ reflection profile obtained

from a stacking fault (see page 151).

If a dislocation lies at  $1/4 \leq y/t \leq 3/4$  in an illuminated area, the Burgers vector can be safely determined even though it is oblique to the specimen surface.

Dependence on specimen thickness

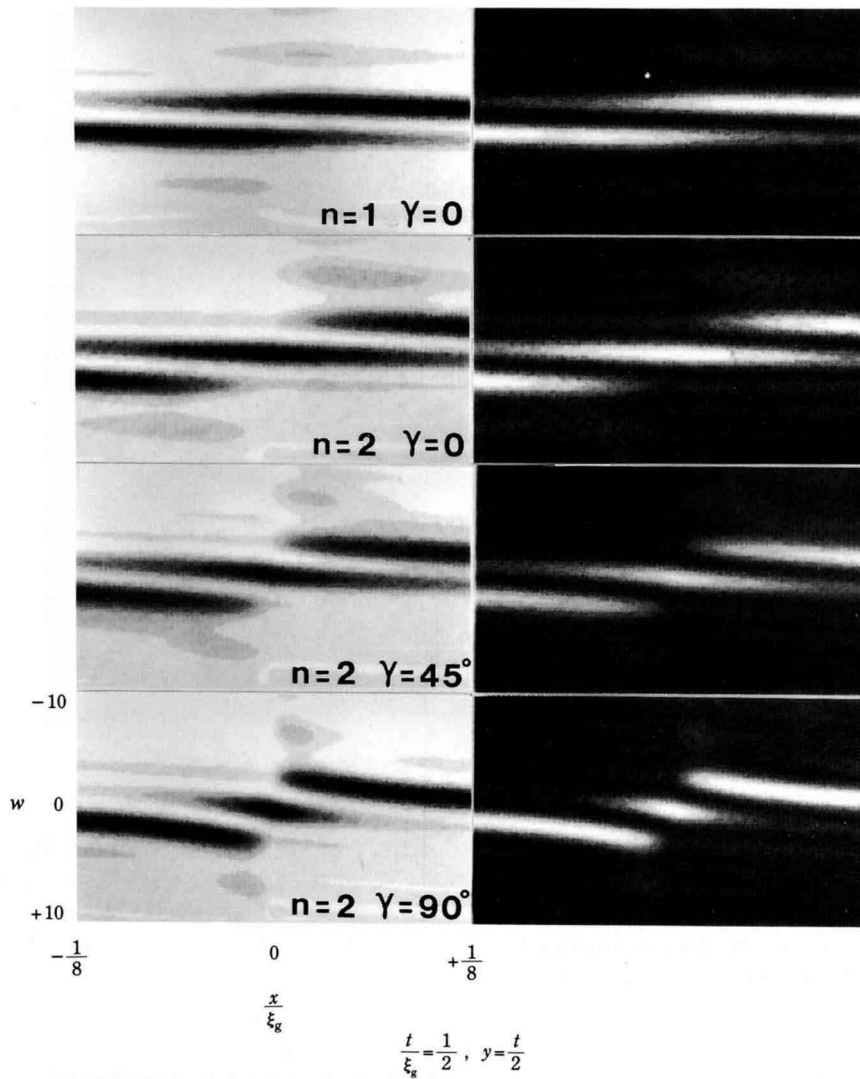


For thinner specimens, the deviation of a reflection line from  $w=0$  becomes larger, but the number of the nodes

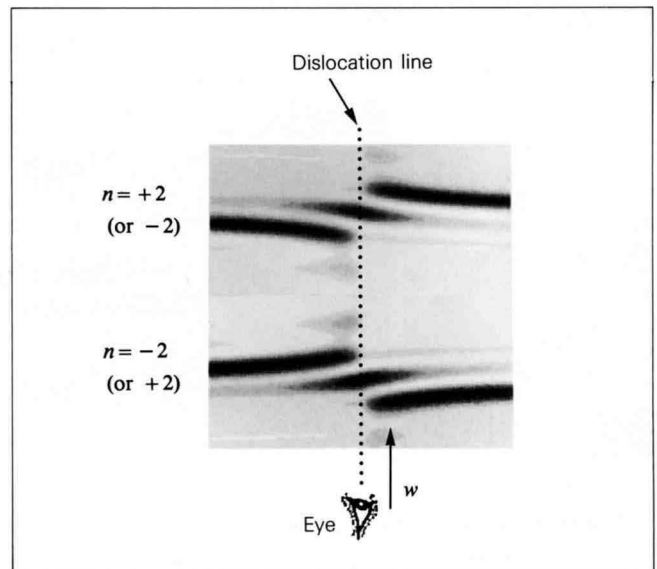
remains the same (see page 152).

## Simulations of a reflection line crossing an edge dislocation

Dependence on the values of  $g \cdot b = n$  and  $\gamma$



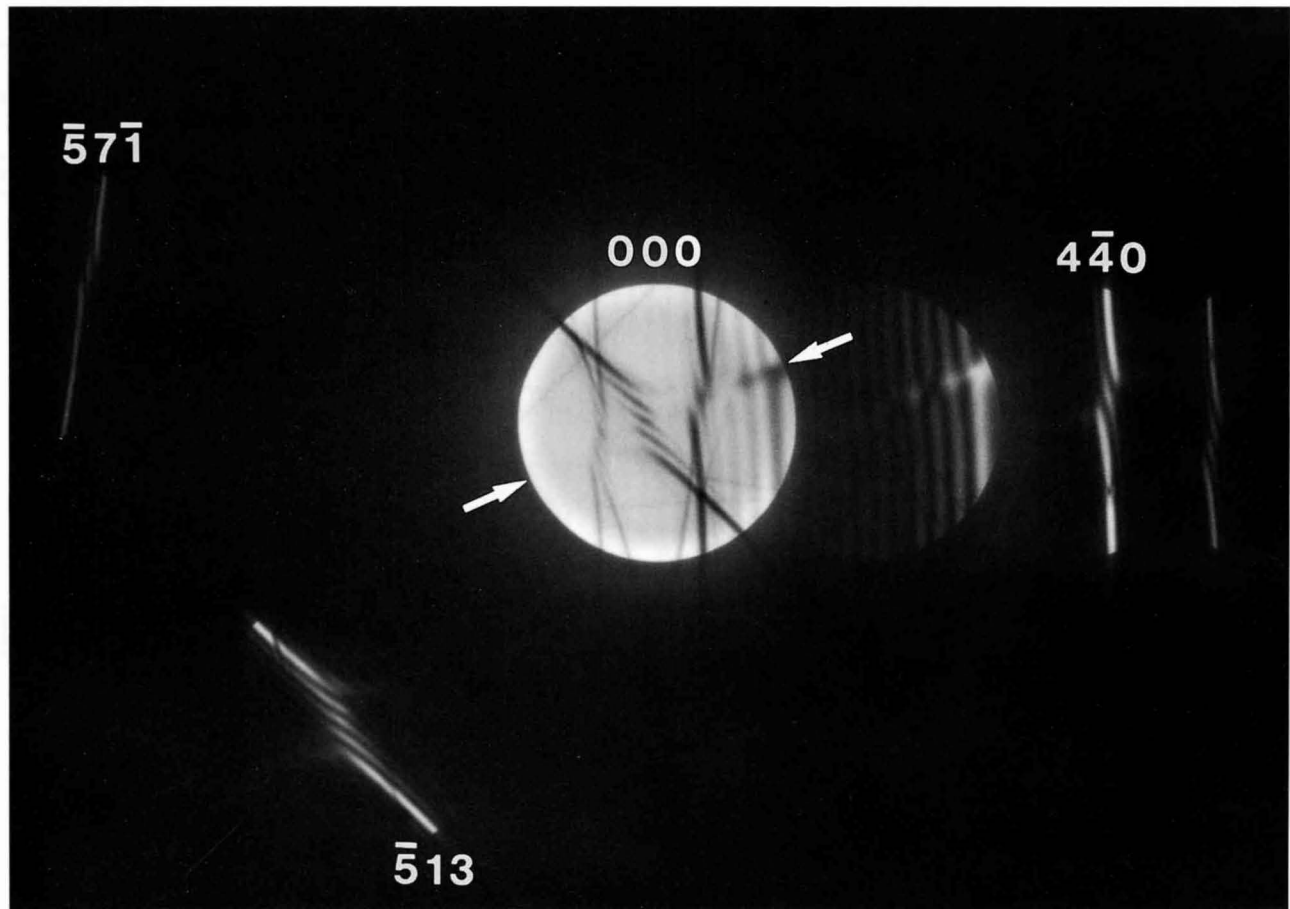
Defocus CBED patterns from an edge dislocation are very similar to those from a screw dislocation except a longer splitting in the horizontal direction  $x$  (see upper two figures). As the angle  $\gamma$  of the edge dislocation from the specimen surface (Fig. (b) on page 160) increases, the range of the splitting decreases as seen in the lower two figures.



## Burgers vector determination

### 1) Si

200 kV



Illuminated specimen area: approx. 200 nm in diameter

$\mathbf{b}=[uvw]$	$\mathbf{g}$	$\mathbf{g}\cdot\mathbf{b}=n$
	$4\bar{4}0$	$4u-4v=-2$
	$\bar{5}13$	$-5u+v+3w=+4$
	$\bar{5}7\bar{1}$	$-5u+7v-w=+2$

$\longrightarrow \mathbf{b}=\frac{1}{2}[\bar{1}01]$

For Burgers vector determination, it is not necessary to set a crystal at a particular zone axis, but at an orientation so that three linearly independent reflections are excited. The photo shows a defocus CBED pattern taken at such a crystal setting from an area containing a dislocation. We omit to use the lowest order reflection for the determination. The position of the dislocation line is indicated by the arrows. Let us write the Burgers vector  $\mathbf{b}=[uvw]$ . The  $4\bar{4}0$ ,  $\bar{5}13$  and  $\bar{5}7\bar{1}$  reflections give values of  $n = -2, +4$  and  $+2$ , respectively. The signs of  $n$  were determined relatively. By solving the linear system of equations, the Burgers vector was determined to be  $\mathbf{b} = 1/2[\bar{1}01]$ . The (relative) sign of  $n$  is very important.

A practical method to determine the relative sign of  $n$

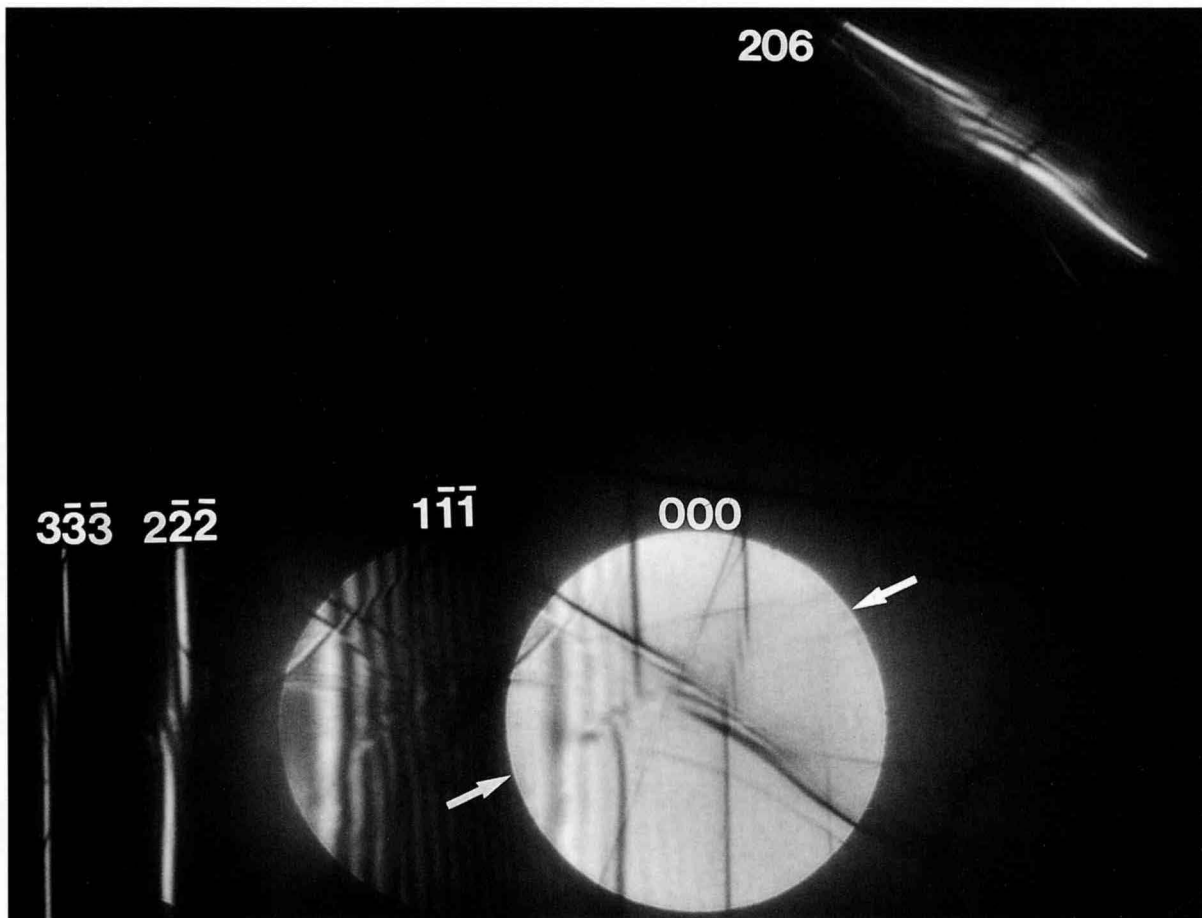
is illustrated in the figure on the opposite page. Look at a reflection line from a sense along the dislocation line (upward in the figure). Observe the sense of the bend of the reflection line with respect to the sense of the excitation error  $w$ . Regard one sense of bend as positive and the other as negative. We do not intend, here, to determine the sign of the Burgers vector.

It is noted that the dislocation of Si was assumed to be a perfect dislocation, because of a small separation of the two extended partials. The effect of the dissociation can be detected using a reflection satisfying  $\mathbf{g}\cdot\mathbf{b}=0$  as will be seen later.

The Si specimens containing dislocations were supplied by Dr. I. Yonenaga and Prof. K. Sumino.

2) Al

80 kV



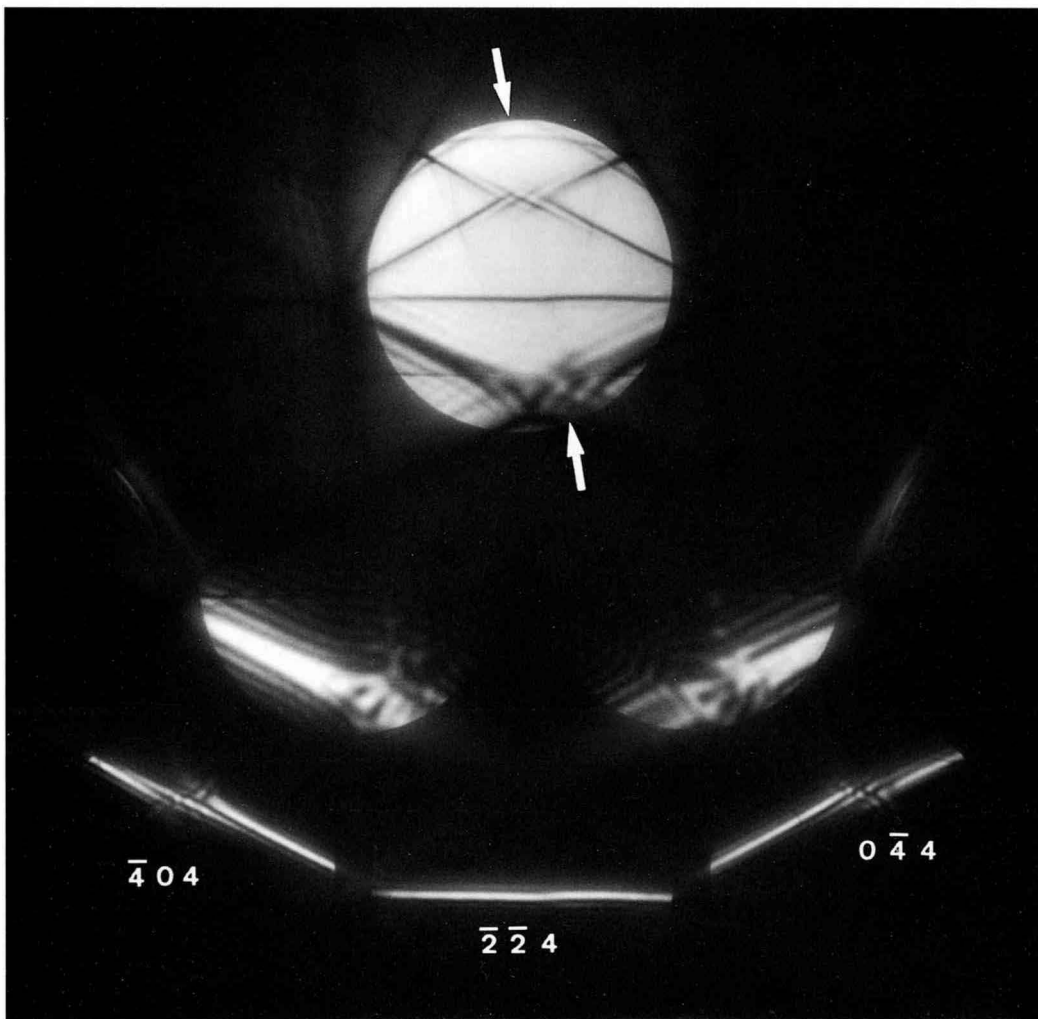
Illuminated specimen area: approx. 200 nm in diameter

$$b = \frac{1}{2}[uvw] \begin{array}{|c|c|} \hline \mathbf{g} & \mathbf{g} \cdot \mathbf{b} = n \\ \hline 2\bar{2}\bar{2} & u - v - w = -2 \\ 206 & u + 3w = +3 \\ \hline \end{array} \longrightarrow \mathbf{b} = \frac{1}{2}[011]$$

Three reflection lines show splittings. As the  $2\bar{2}\bar{2}$  and  $3\bar{3}\bar{3}$  reflections are linearly dependent, we have only two equations to solve. We assume that the dislocation has a Burgers vector of the  $1/2 \langle 110 \rangle$  type. Then, we can determine the vector to be  $\mathbf{b} = 1/2[011]$ .

3) Al

60 kV



Illuminated specimen area: approx. 100 nm in diameter

$$\mathbf{b} = \frac{1}{2}[uvw]$$

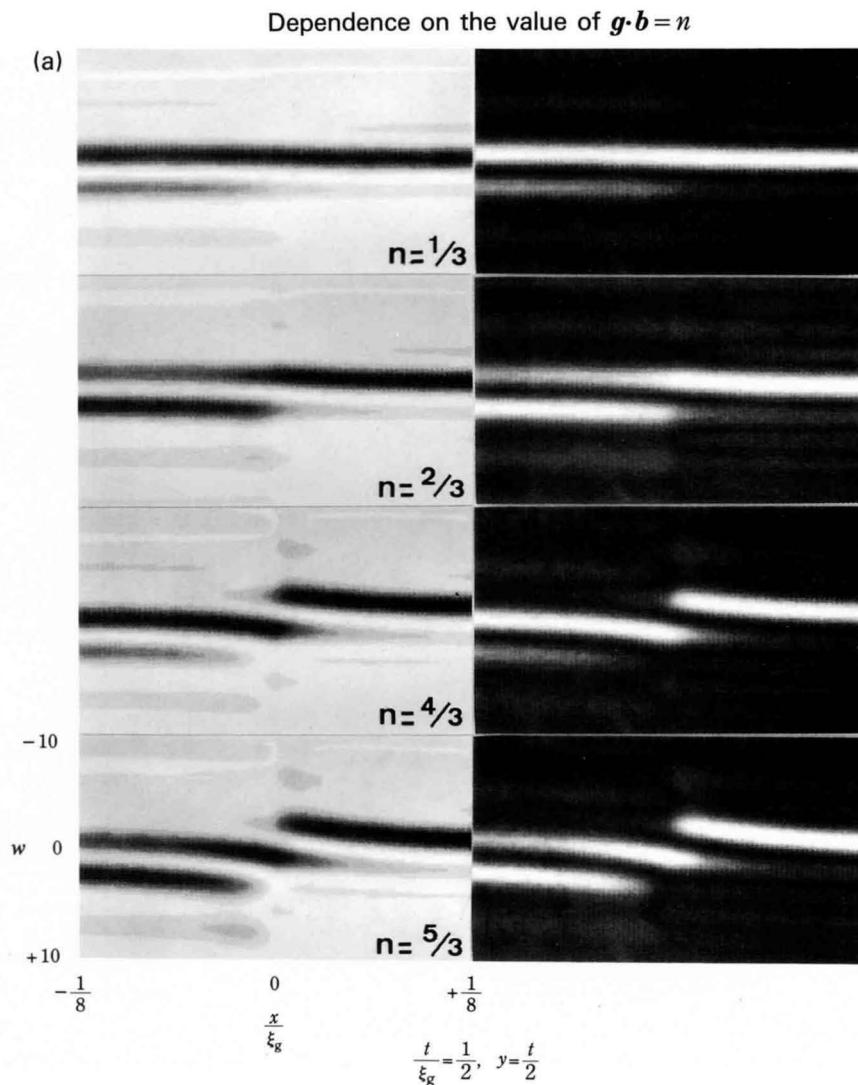
$g$	$g \cdot \mathbf{b} = n$
$\bar{4}04$	$-2u + 2w = +2$
$0\bar{4}4$	$-2v + 2w = -2$
$\bar{2}\bar{2}4$	$-u - v + 2w = 0$

$$\rightarrow \mathbf{b} = \frac{1}{2}[\bar{1}10]$$

The Burgers vector was assumed to be of the  $1/2 \langle 110 \rangle$  type.

## Determination of Burgers vectors of partial dislocations

### Simulations of a reflection line crossing a partial screw dislocation

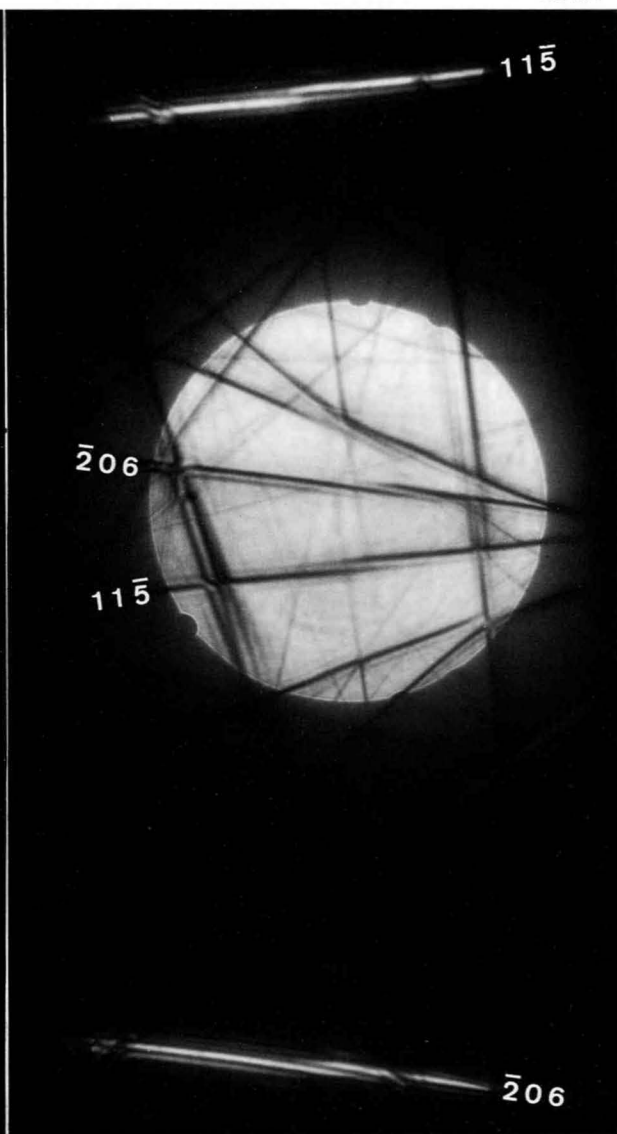
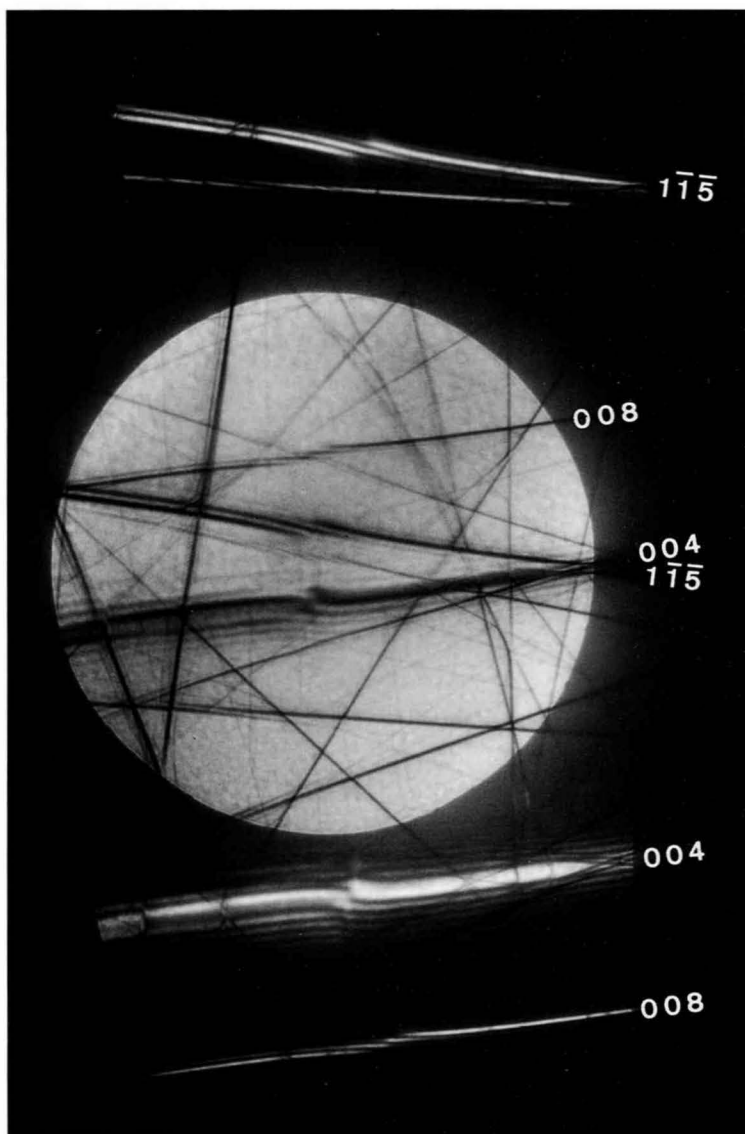


A partial dislocation has a Burgers vector which is not a lattice vector and is accompanied by a stacking fault at one side of it. In the case of face-centered cubic crystals,  $n = g \cdot b$  takes values  $0, \pm 1/3, \pm 2/3, \pm 1, \pm 4/3 \dots$ . Figure (a) shows computed CBED profiles of a reflection line crossing a partial dislocation and a stacking fault. The partial dislocation was assumed to be of the screw type for simplicity of calculation. The stacking fault was assumed to be present at  $x < 0$ . Near the dislocation, the profiles for  $n = N + 1/3$  and  $n = N + 2/3$  ( $N$ : integer) are similar to that for  $n = N$  of a perfect dislocation. With increasing  $x$  in the negative direction, the profiles become similar to those obtained from a stacking fault for  $\alpha = 2\pi g \cdot R = \pm (2/3)\pi$  (compare with the profiles shown in the section

Photographs (a) and (b) show defocus CBED patterns taken from an about 250 nm diameter specimen area containing a stacking fault and a partial dislocation, shown in Photo (c). The  $1\bar{1}\bar{5}$  and 008 reflection profiles are of  $n = +5/3$  and  $n = -8/3$ , respectively. The low order 004 reflection is discarded, because the identification of  $n$  is difficult. The  $11\bar{5}$  and  $\bar{2}06$  reflection profiles are of  $n = 1$  and  $n = -4/3$ , respectively. From the three equations among four, the Burgers vector is determined to be  $b = 1/3[\bar{1}\bar{1}\bar{1}]$

Si

80 kV



Illuminated specimen area: approx. 250 nm in diameter

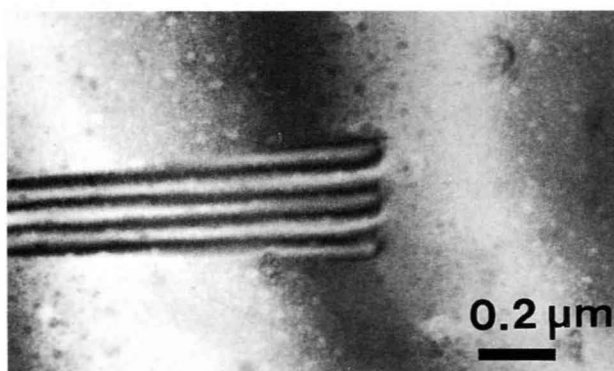
(a)

(b)

$$\mathbf{b} = [uvw]$$

$g$	$g \cdot b = n$
$1\bar{1}\bar{5}$	$u - v - 5w = +\frac{5}{3}$
008	$8w = -\frac{8}{3}$
$11\bar{5}$	$u + v - 5w = +1$
$\bar{2}06$	$-2u + 6w = -\frac{4}{3}$

$$\rightarrow \mathbf{b} = \frac{1}{3}[\bar{1}\bar{1}\bar{1}]$$

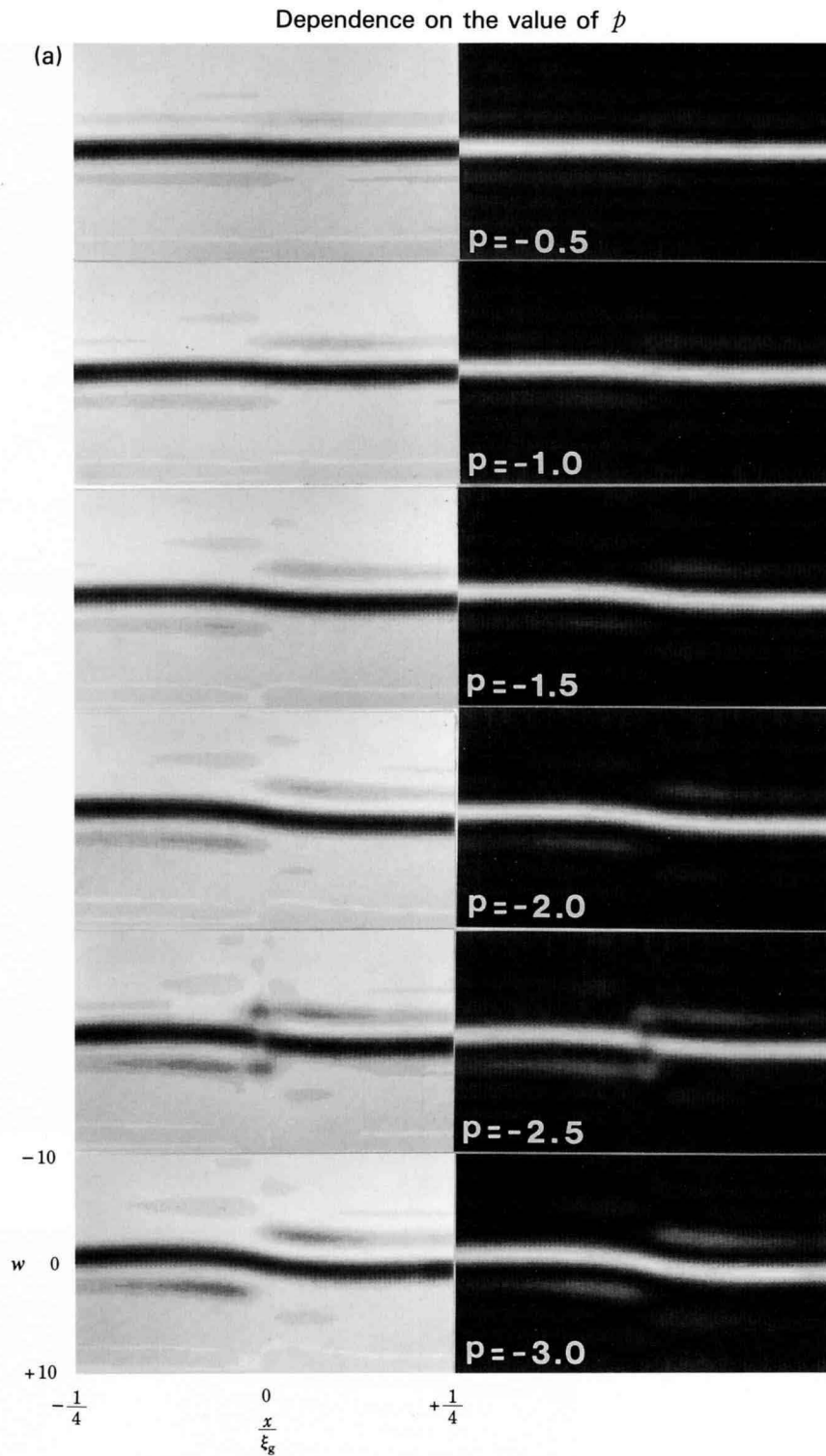


$$\mathbf{b} = \frac{1}{3}[\bar{1}\bar{1}\bar{1}]$$

(c)

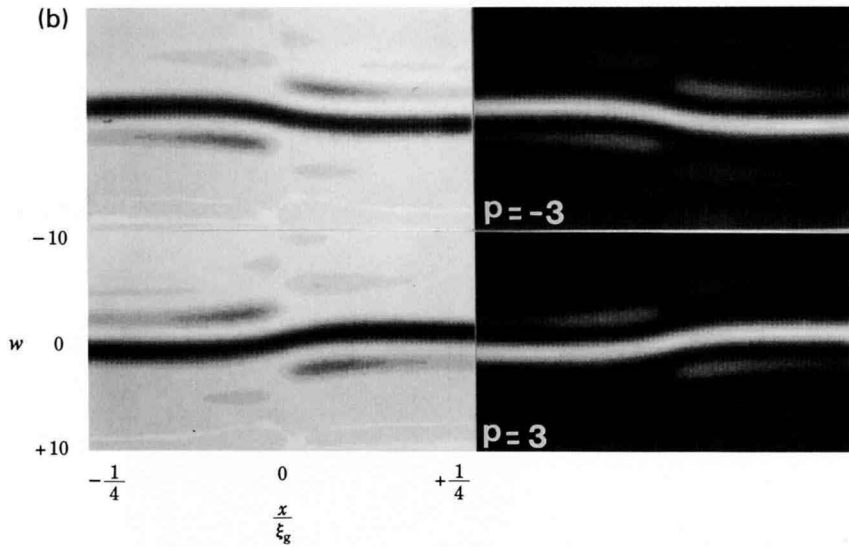
## Investigation of edge and mixed dislocations

Simulations of a reflection line crossing a  $60^\circ$  dislocation: Effect of  $g \cdot b_e = p$  at  $g \cdot b = 0$



$$\frac{t}{\xi_g} = \frac{1}{2}, \quad y = \frac{t}{2}, \quad n=0, \quad m=0, \quad \gamma=0^\circ$$

Dependence on the sign of  $p$

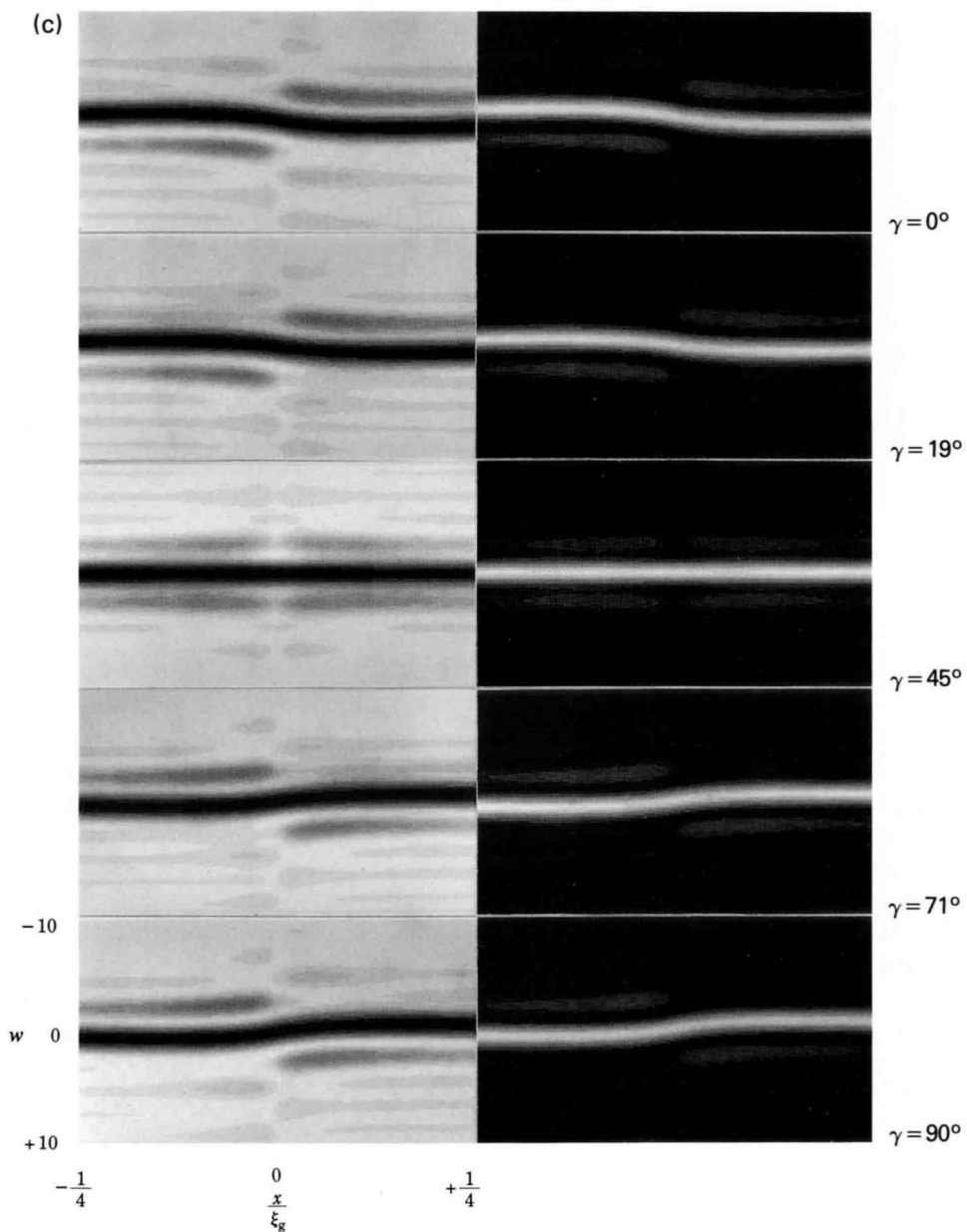


$$\frac{t}{\xi_g} = \frac{1}{2}, \quad y = \frac{t}{2}, \quad n=0, \quad m=0, \quad \gamma=0^\circ$$

The condition  $\mathbf{g} \cdot \mathbf{b} = 0$  is not a sufficient condition for the invisibility of edge and mixed dislocations. The second and third terms of equation (1) on page 160 cause changes in the form of a reflection line. The second term, expresses the atomic displacements parallel to the slip plane and the third term the displacements perpendicular to the slip plane. It should be noted that the resultants of these displacements along the entire Burgers

circuit are zero. The effect of the second term of  $p = \mathbf{g} \cdot \mathbf{b}_e$  produces a bend similar to a kink in a reflection line. Figure (a), which was calculated for  $\gamma = 0^\circ$ , shows that the bend increases with the value of  $p$ . The sense of the bend becomes opposite when the sign of  $p$  is changed (Fig. (b)). When  $\gamma$  is increased for a definite value of  $p$ , the sense of the bend becomes opposite at  $\gamma = 45^\circ$ , as shown in Fig. (c).

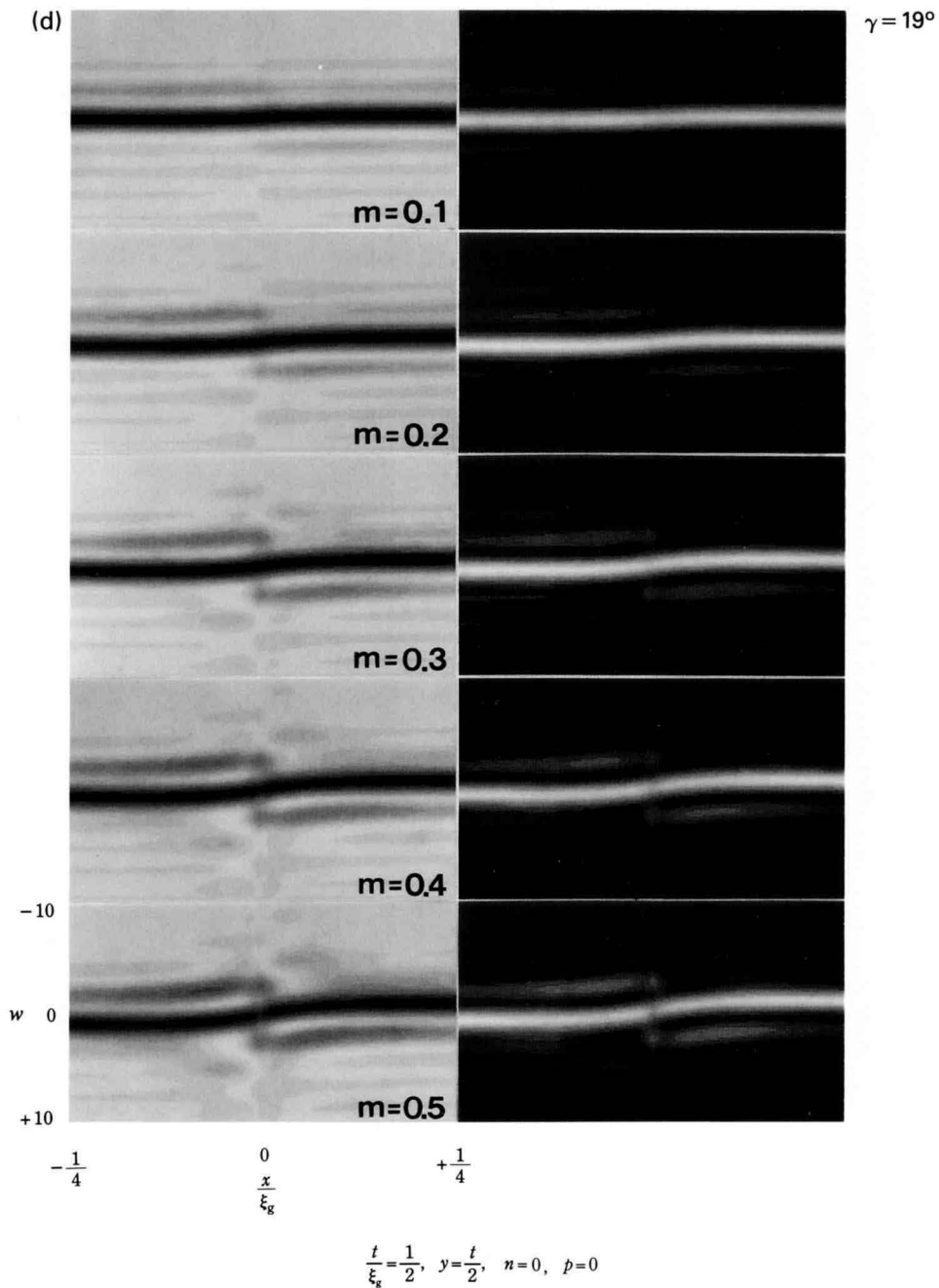
Dependence on angle  $\gamma$



$$\frac{t}{x_g} = \frac{1}{2}, \quad y = \frac{t}{2}, \quad n=0, \quad m=0, \quad p=-2$$

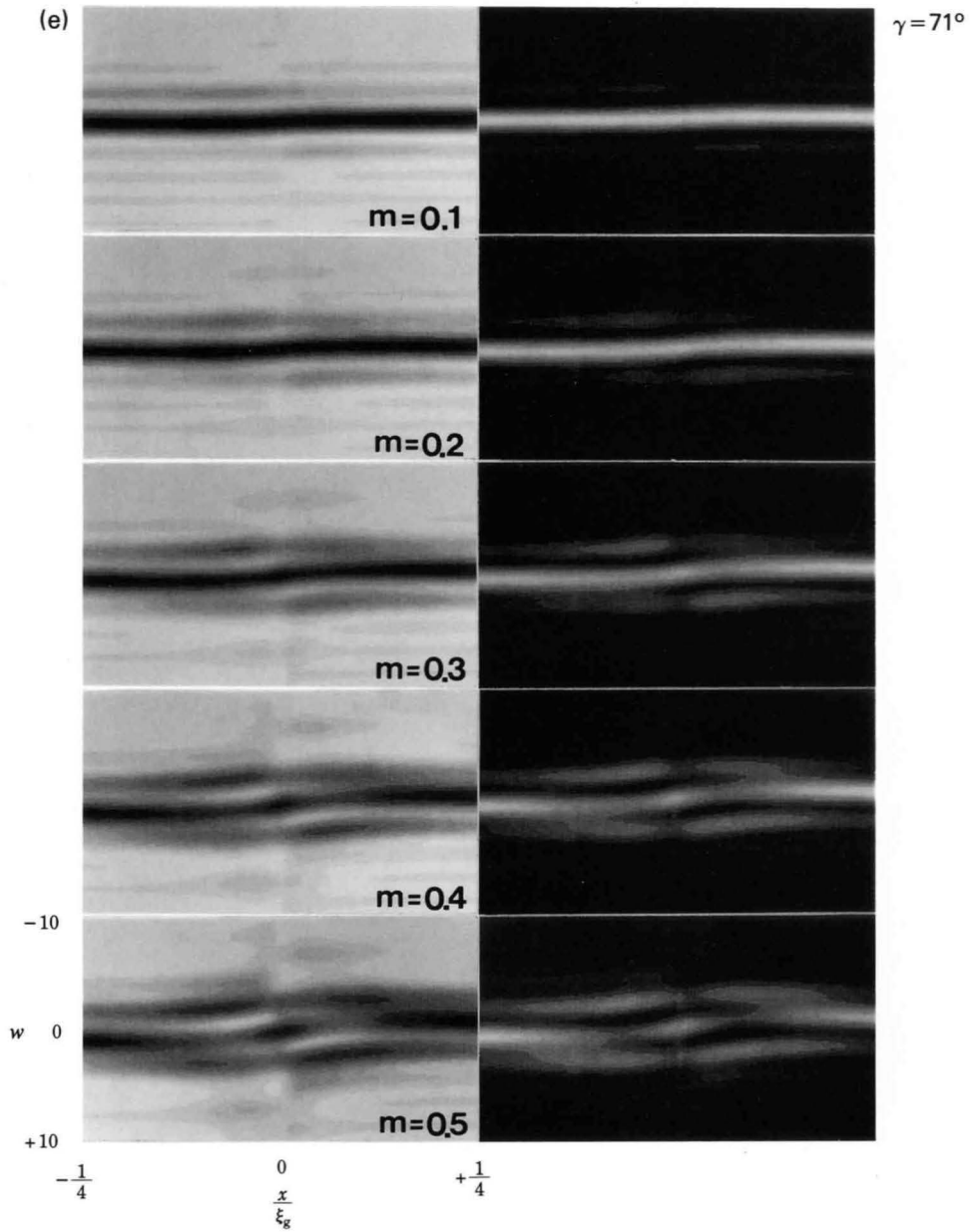
**Simulations of a reflection line crossing an edge dislocation: Effect of  $\frac{1}{8} \mathbf{g} \cdot \mathbf{b} \times \mathbf{u} = m$  at  $\mathbf{g} \cdot \mathbf{b} = 0$**

Dependence on the value of  $m$



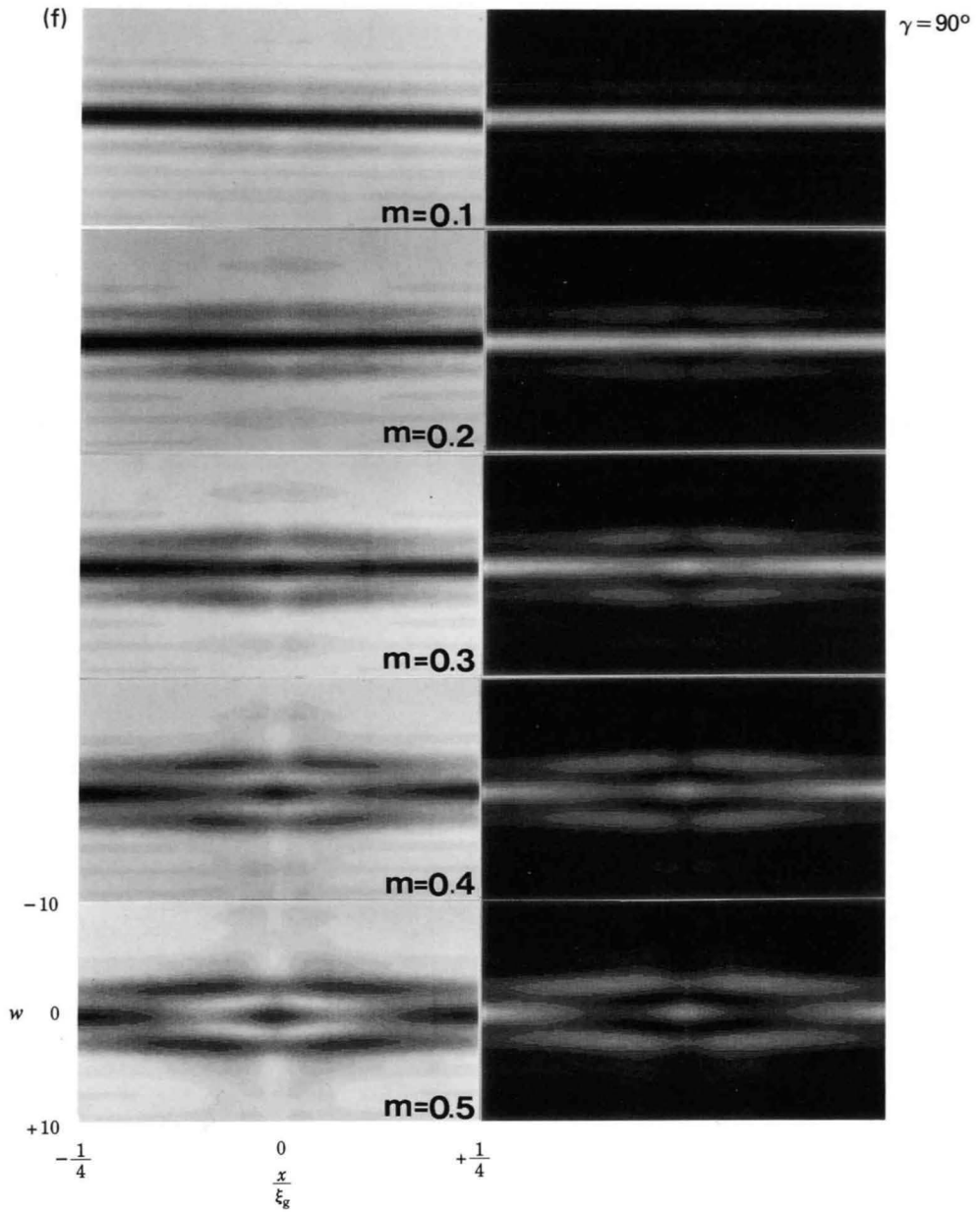
The effect of the third term,  $m = 1/8 \mathbf{g} \cdot \mathbf{b} \times \mathbf{u}$ , causes a bend similar to that for  $p$ , but accompanied by stronger subsidiary maxima, as seen in Fig. (d). When the angle  $\gamma$  approaches  $90^\circ$ , the pattern becomes symmetric with respect to  $x=0$  and  $w=0$  (Figs. (e) and (f)). The sense of the bend becomes opposite when the sign of  $m$  is changed (Fig. (g)).

Dependence on the value of  $m$



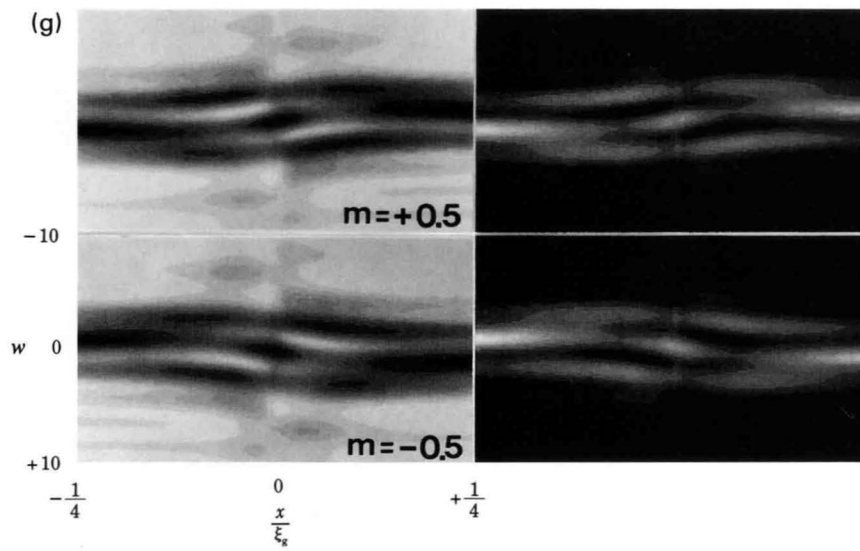
$$\frac{t}{x_g} = \frac{1}{2}, \quad y = \frac{t}{2}, \quad n=0, \quad p=0$$

Dependence on the value of  $m$



$$\frac{t}{\xi_g} = \frac{1}{2}, \quad y = \frac{t}{2}, \quad n=0, \quad p=0$$

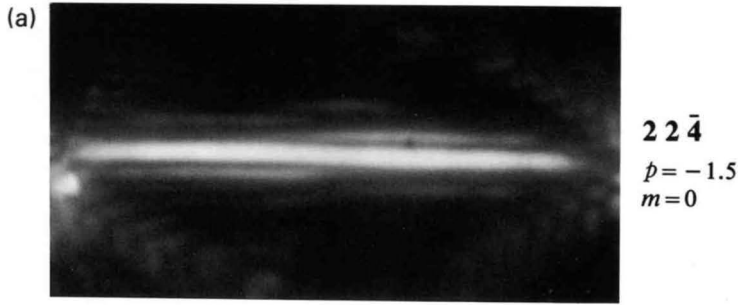
Dependence on the sign of  $m$



$$\frac{t}{\xi_g} = \frac{1}{2}, y = \frac{t}{2}, n=0, p=0, \gamma=71^\circ$$

60° dislocation of Al 200 kV

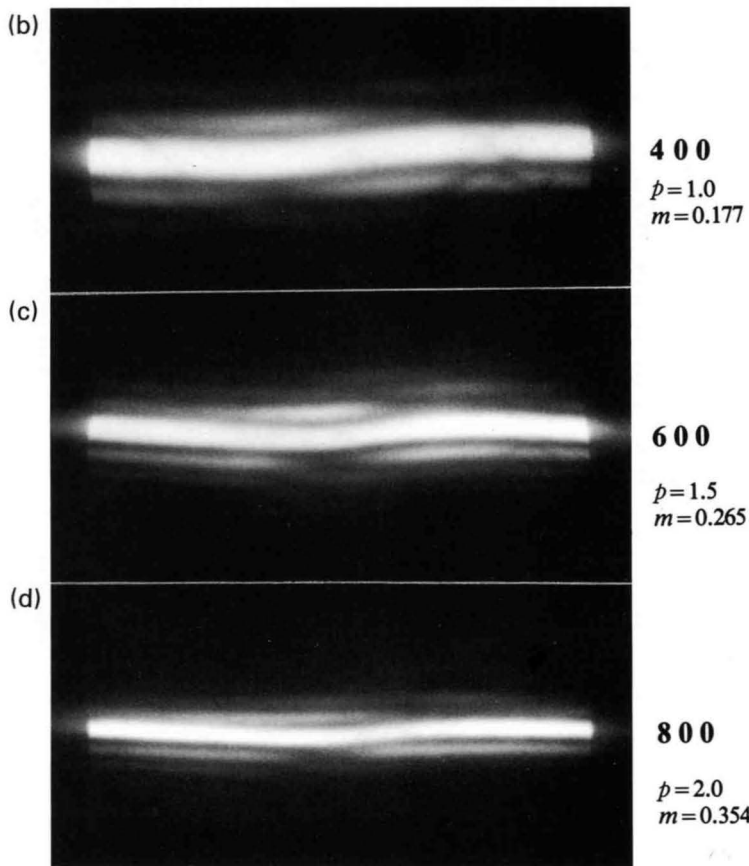
Effect of  $p = g \cdot b_e$



$$u = \frac{1}{\sqrt{2}} [10\bar{1}], b = \frac{1}{2} [1\bar{1}0], b_e = \frac{1}{4} [1\bar{2}1], n = 0, \gamma = 0^\circ$$

Photograph (a) is a  $22\bar{4}$  dark-field pattern taken from a  $60^\circ$  dislocation of Al at the condition  $g \cdot b = 0$ . The bend of the reflection line is caused by  $p$ , showing a qualitatively good agreement with the theoretical results (Fig. (a) on page 170).

Effect of  $m = \frac{1}{8} g \cdot b \times u$



$$u = \frac{1}{\sqrt{2}} [\bar{1}10], b = \frac{1}{2} [0\bar{1}1], b_e = \frac{1}{4} [11\bar{2}], n = 0, \gamma = 35^\circ$$

Photographs (b),(c) and (d) are 400, 600 and 800 dark-field patterns taken from a  $60^\circ$  dislocation of Al at the condition of  $g \cdot b = 0$ . The values of  $p$  and  $m$  are written at each photo. The observed bend of the reflection line is almost due to  $m$ , because the effect of  $p$  at  $\gamma = 35^\circ$  is very small (see Fig. (c) on page 172). It is seen that the bend increases as the value of  $m$  increases, showing a qualitatively good agreement with the theoretical results (Fig. (d) on page 173).

## Determination of the Burgers vector of a dislocation loop

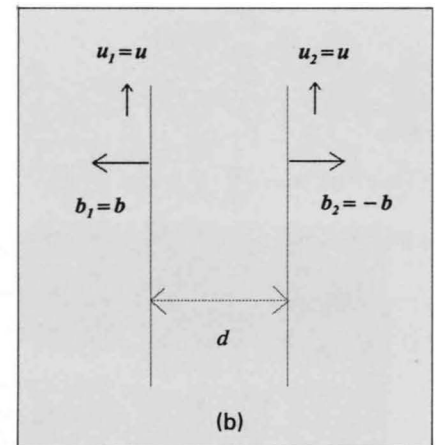
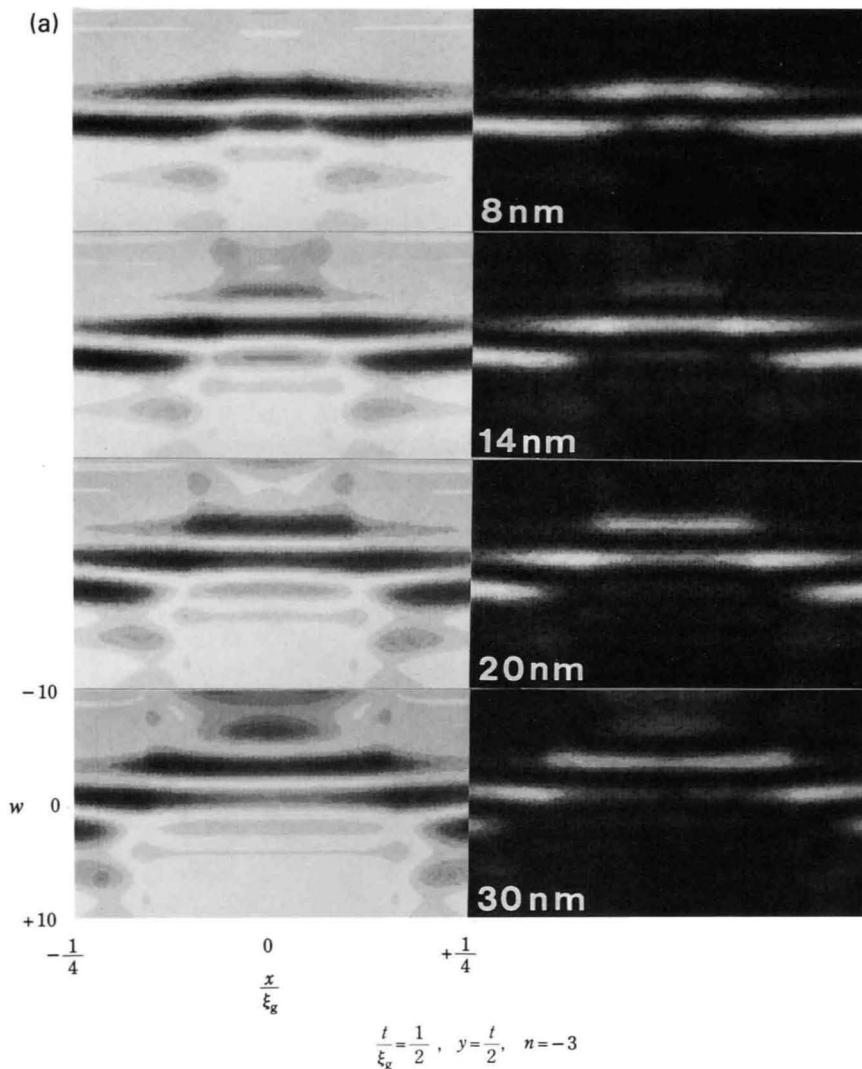
Figure (a) shows computed profiles of a reflection line crossing an edge dislocation dipole for  $n = \pm 3$ ,  $u_1$ ,  $u_2$ ,  $b_1$  and  $b_2$  being shown in Fig. (b). In the computations the left dislocation was assumed to give a value of  $n = +3$  and the right one  $n = -3$ . When the two dislocations consisting of the dipole are interchanged, the patterns are reversed with respect to the line of  $w=0$ . The computed results are extensively applicable to a dislocation loop, by changing the sign of  $u_1$  (or  $u_2$ ).

Defocus CBED patterns can determine the Burgers vec-

tor of a dislocation loop, without observing the change of contrast of the loop by varying diffraction condition, which is necessary in the electron-microscope-image method. Figures (c) and (d) illustrate a dislocation loop whose Burgers vector is oblique to the incident beam. When the sense of a dislocation line  $u$  is defined as shown in Fig.(c), the Burgers vector of a dislocation loop is defined to be  $b$  as shown in Figs.(d)-(i) and (d)-(ii) for a vacancy type and an interstitial type using FS/RH convention. Schematic diagrams of a reflection line crossing

## Simulations of a reflection line crossing a dislocation dipole

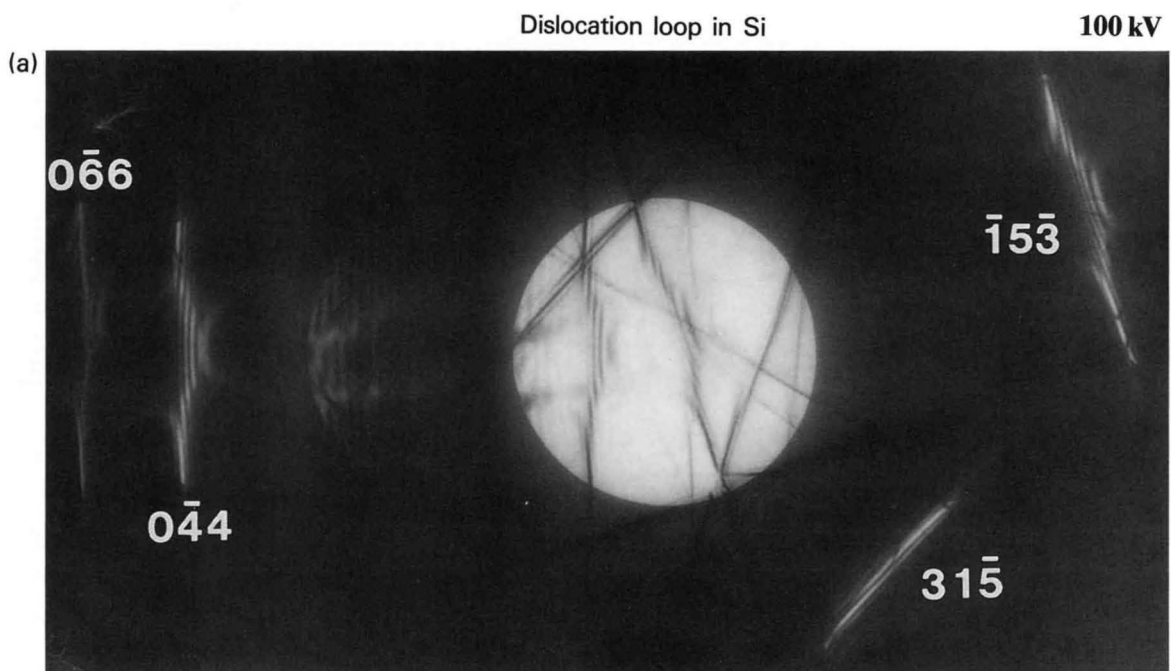
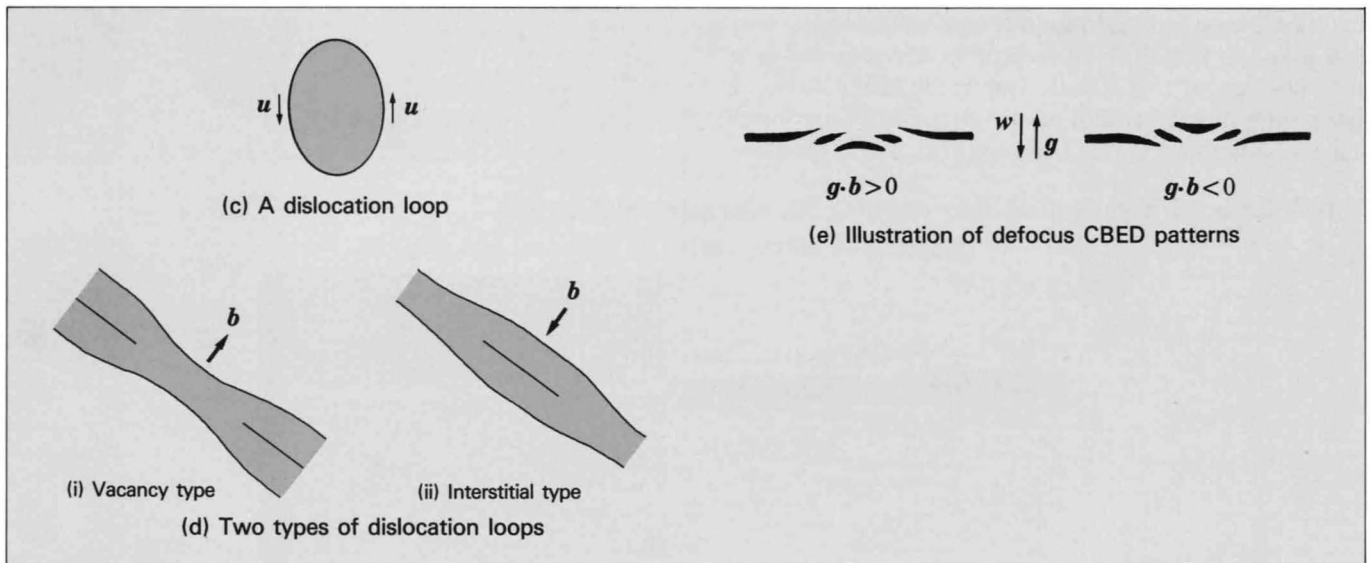
Dependence on the separation of a dipole



a dislocation loop for  $n = \mathbf{g} \cdot \mathbf{b} > 0$  and  $n = \mathbf{g} \cdot \mathbf{b} < 0$  are shown in Fig.(e). The sense of the pattern with respect to a sense of  $w$  is opposite to each other between the cases of  $n > 0$  and  $n < 0$ . The sign of  $n$  is determined absolutely. The Burgers vector  $\mathbf{b}$  of the loop including its sense (vacancy type or interstitial type) can be determined from the values of  $\mathbf{g} \cdot \mathbf{b}$  and their signs. The sign of  $\mathbf{b}$  is determined in the present case in contrast to the case of dislocations (see page 165).

Photograph (a) was taken from a (111) Si film containing a dislocation loop with several ten nm in diameter. The

$0\bar{4}4$  and  $\bar{1}5\bar{3}$  reflections were found to have values of  $n = +8/3$  and  $-7/3$ , respectively, where the outermost broad contrast was neglected. By assuming the Burgers vector to be of the  $1/3\langle 111 \rangle$  type, the Burgers vector of the loop was determined as  $\mathbf{b} = 1/3[\bar{1}\bar{1}1]$  or an interstitial type. When more reflection lines crossing the loop are observed, more reliable determination is carried out. Decrease of the size of the loop makes difficult reliable determination. The identification of the sense of  $\mathbf{b}$  for smaller loops is under study.



$$0\bar{4}4 : n \cong +\frac{8}{3}, \quad \bar{1}5\bar{3} : n \cong -\frac{7}{3}, \quad \mathbf{b} = \frac{1}{3}[\bar{1}\bar{1}1]$$

## Investigation of extended dislocations

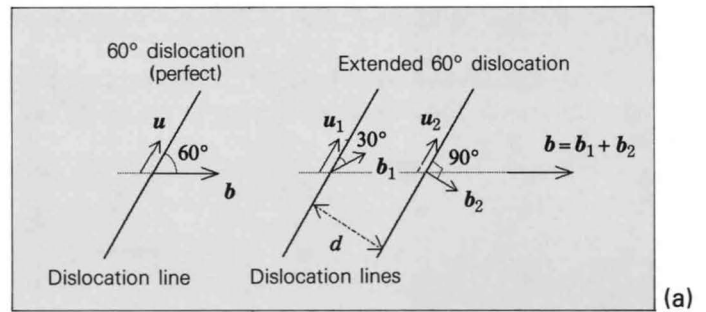
### 60° dislocation of Si extended into a 30° and an edge partial dislocation

In a face-centered cubic or diamond type crystal, a 60° dislocation with a Burgers vector of  $\mathbf{b} = 1/2 \langle 110 \rangle$  type can extend into two partial dislocations accompanied by a stacking fault (Fig.(a)):

$$1/2 \langle 110 \rangle \rightarrow 1/6 \langle 21\bar{1} \rangle + 1/6 \langle 121 \rangle,$$

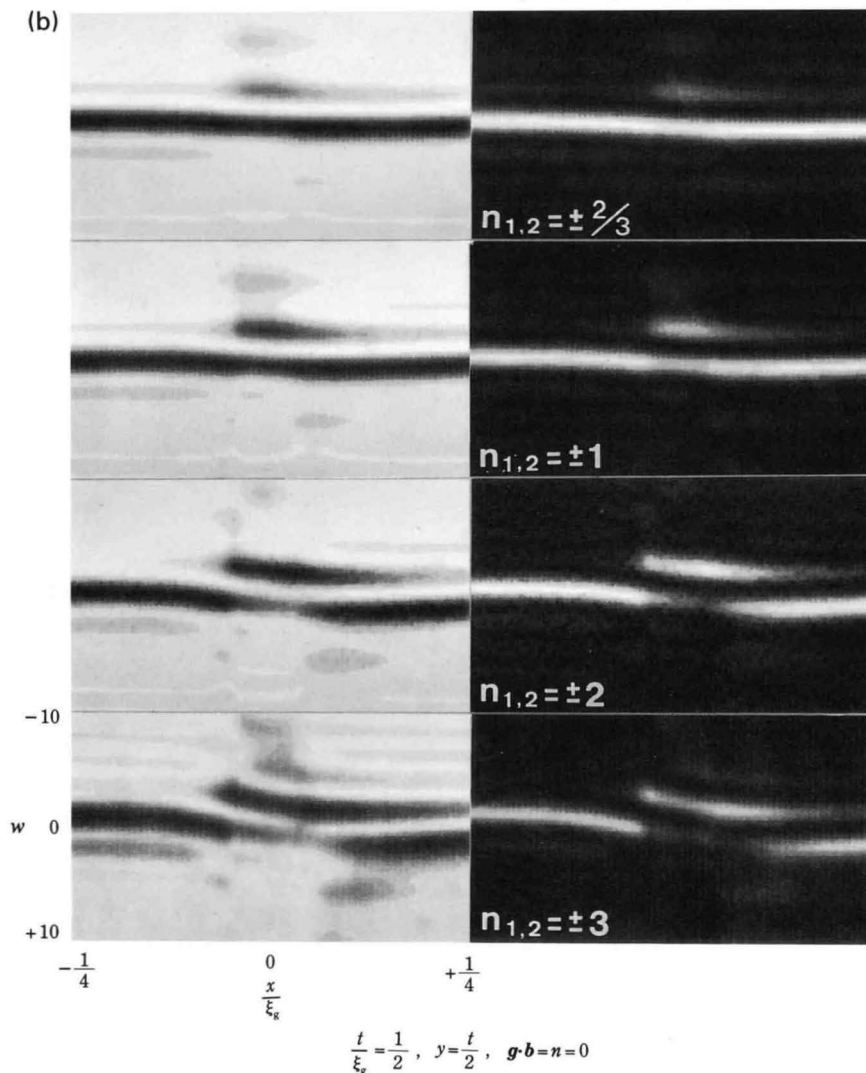
where one is a 30° partial dislocation and the other is an edge partial. The profile of a reflection line crossing an extended dislocation for  $\mathbf{g} \cdot \mathbf{b} = n \neq 0$  is similar to that obtained from a perfect dislocation for the same  $n$ , as far as the separation is small. The profiles of reflection lines for  $\mathbf{g} \cdot \mathbf{b} = 0$  were computed for different values of  $\mathbf{g} \cdot \mathbf{b}_1 = n_1$  and  $\mathbf{g} \cdot \mathbf{b}_2 = n_2$  (Fig.(b)). These profiles are regarded as a superposition of two effects. One is the effect due to a dislocation dipole because of  $n_1 + n_2 = n = 0$ , thus forming a subsidiary maximum (see page 178). The other is the

effect due to a mixed dislocation because of a small extended width, forming a bend of the line (see page 170). The sense of the pattern is reversed when the operating reflection is reversed (Fig.(c)). The subsidiary maximum is clearer for an extended width,  $d$ , of 14 nm than for a width of 4 nm (Fig.(d)).

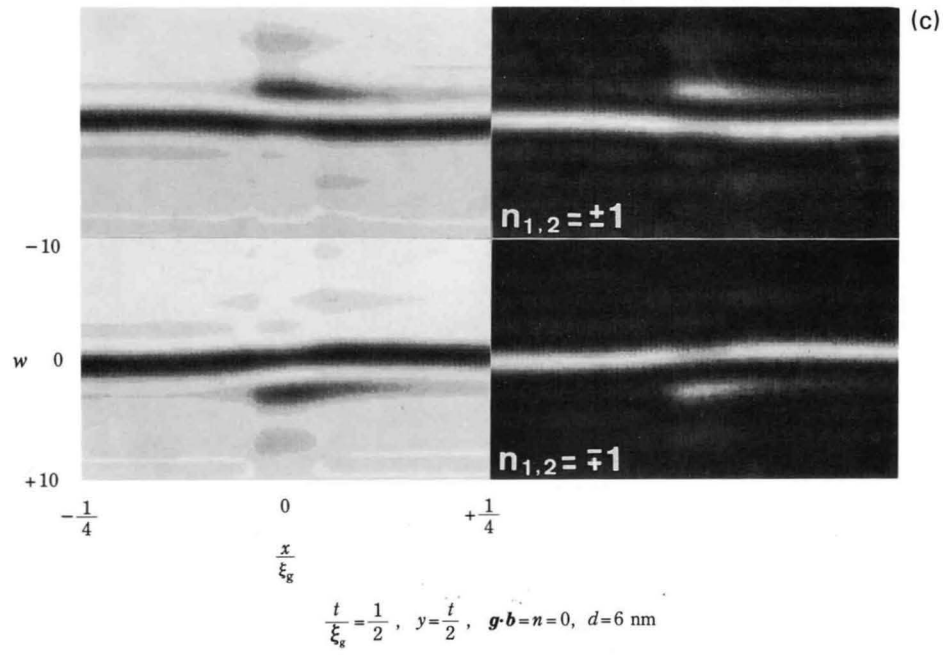


### Simulations of a reflection line crossing an extended dislocation

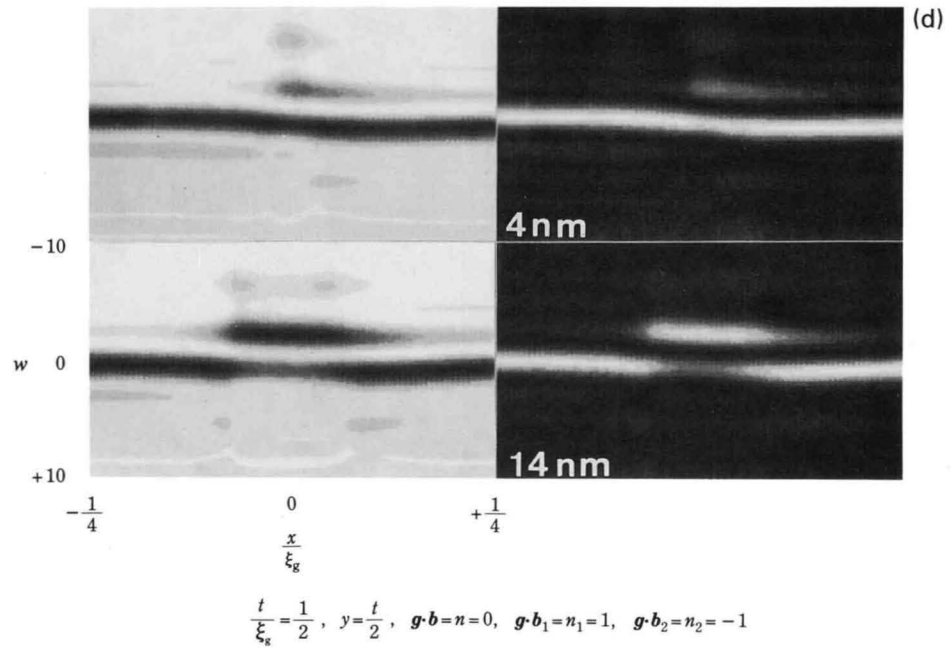
Dependence on the values of  $\mathbf{g} \cdot \mathbf{b}_1 = n_1$  and  $\mathbf{g} \cdot \mathbf{b}_2 = n_2$



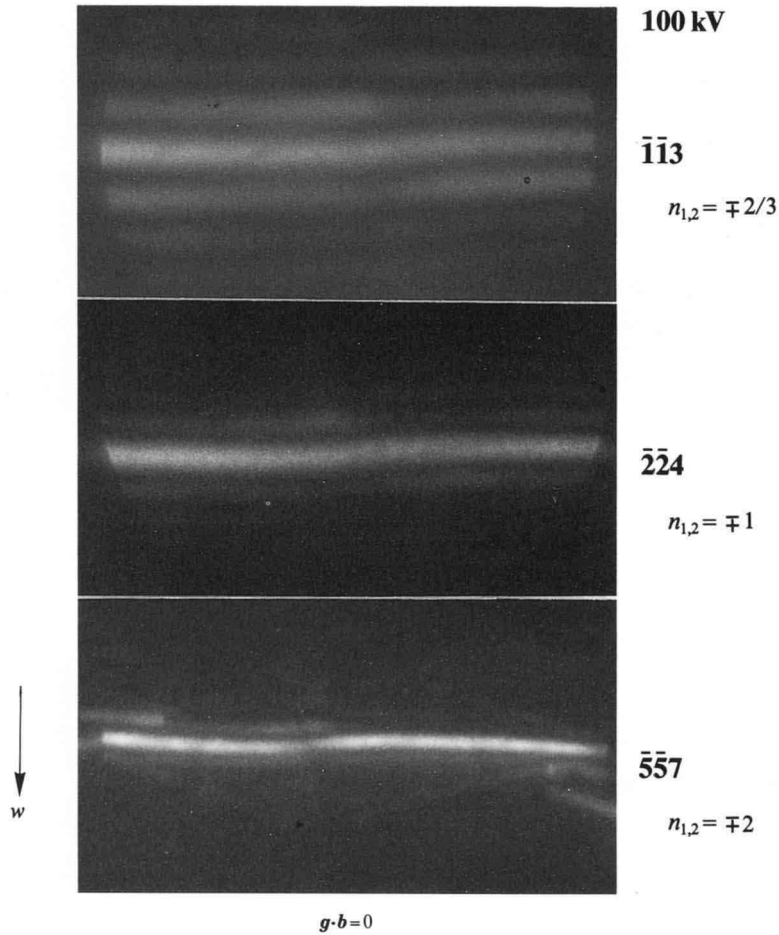
Dependence on the signs of  $\mathbf{g}\cdot\mathbf{b}_1=n_1$  and  $\mathbf{g}\cdot\mathbf{b}_2=n_2$



Dependence on the separation of two partials



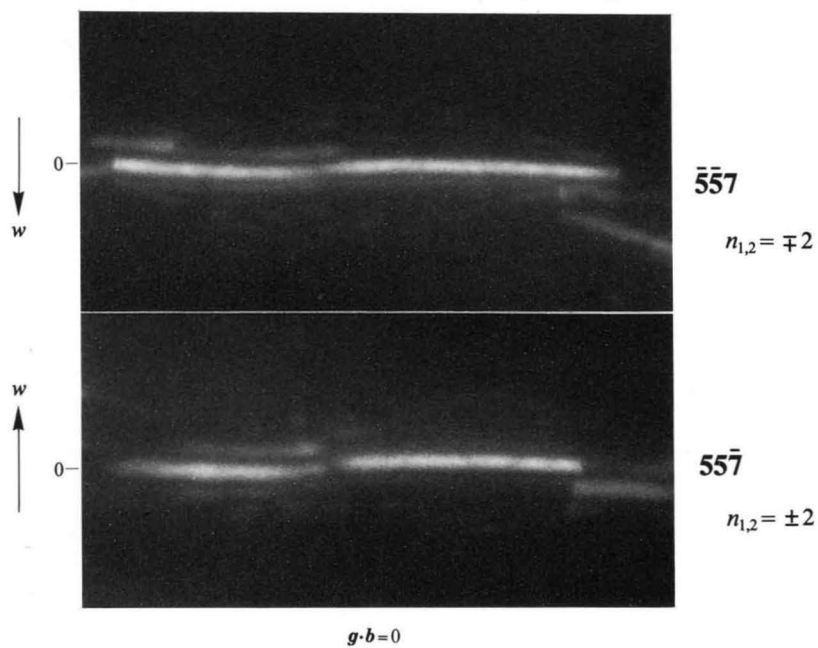
Dependence on the values of  $n_1$  and  $n_2$



$$u = \frac{1}{\sqrt{2}} [0\bar{1}1], \quad b = \frac{1}{2} [1\bar{1}0], \quad b_e = \frac{1}{4} [2\bar{1}\bar{1}], \quad b_1 = \frac{1}{6} [2\bar{1}\bar{1}], \quad b_2 = \frac{1}{6} [1\bar{2}1]$$

Defocus dark-field patterns taken from an extended  $60^\circ$  dislocation of Si at  $g \cdot b = 0$  for three values of  $n_{1,2}$ . Note that the profiles show a qualitative agreement with computed ones.

Dependence on the signs of  $n_1$  and  $n_2$



$$u = \frac{1}{\sqrt{2}} [0\bar{1}1], \quad b = \frac{1}{2} [1\bar{1}0], \quad b_e = \frac{1}{4} [2\bar{1}\bar{1}], \quad b_1 = \frac{1}{6} [2\bar{1}\bar{1}], \quad b_2 = \frac{1}{6} [1\bar{2}1]$$

Defocus dark-field patterns of the  $\bar{5}\bar{5}7$  and  $55\bar{7}$  reflections taken from an extended  $60^\circ$  dislocation of Si where  $g \cdot b = 0$ .

Note that the pattern is reversed with respect to the line of  $w=0$  when the operating reflection is reversed.

### Screw dislocation of Si extended into two 30° dislocations

A screw dislocation with a Burgers vector of  $b = 1/2\langle 110 \rangle$  type in a face-centered cubic or a diamond type crystal can extend into two 30° partials accompanied by a stacking fault (Fig.(a)). In the case of a screw dislocation, a reflection line giving  $g \cdot b = 0$  is parallel to the dislocation line.

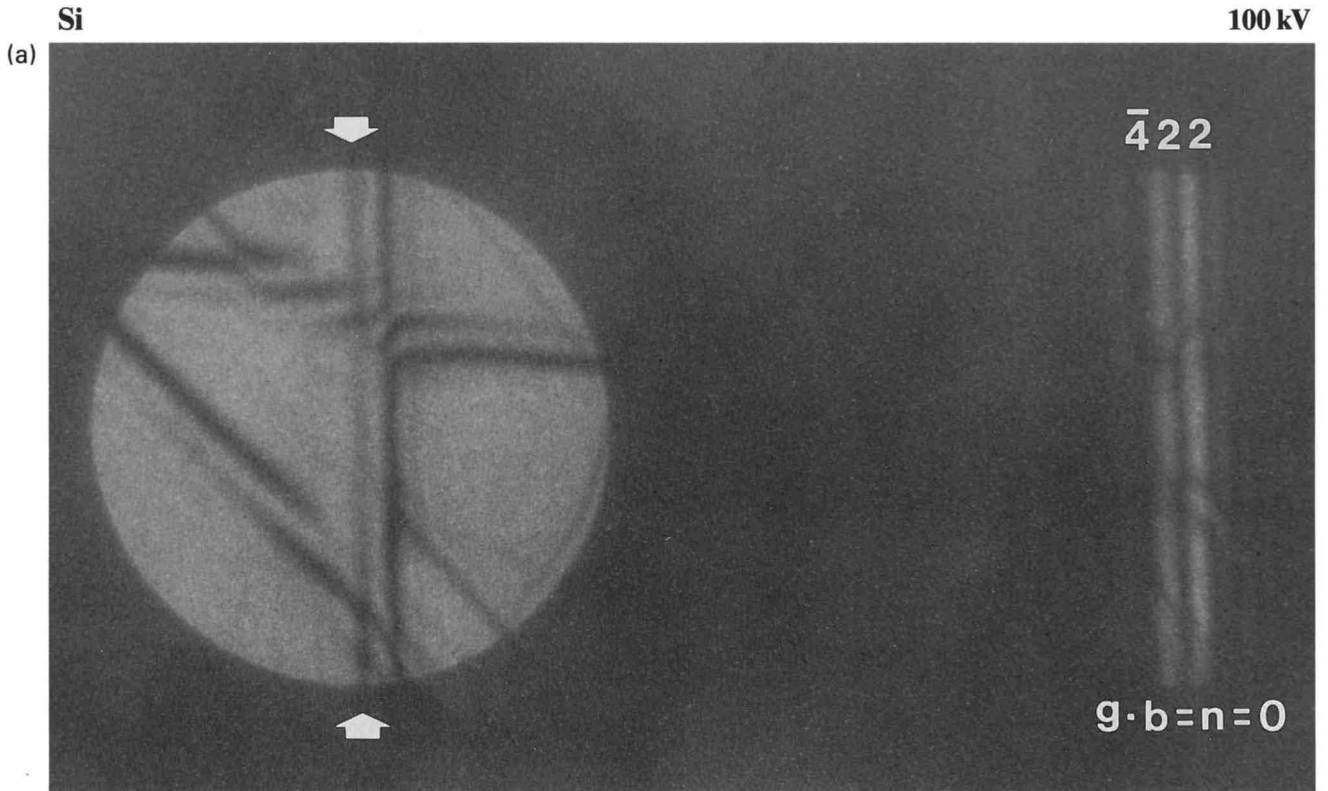
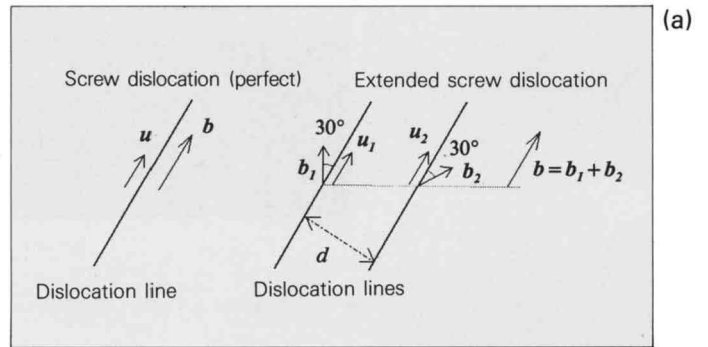
Photograph (a) was taken from an extended screw dislocation of Si at  $g \cdot b = 0$ , where the  $\bar{4}22$  reflection line was superposed on the dislocation line. The reflection line is seen split in two lines. From the condition  $g \cdot b = 0$  for the  $\bar{4}22$  reflection, the Burgers vector of the perfect dislocation was found to be  $1/2[01\bar{1}]$ . The dislocation can dissociate in two ways:

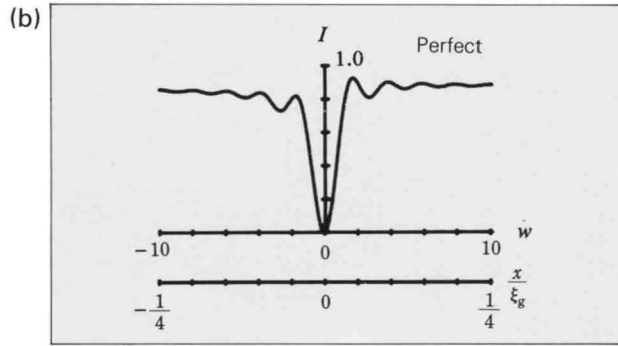
$$1/2[01\bar{1}] \begin{cases} \rightarrow 1/6[\bar{1}2\bar{1}] + 1/6[11\bar{2}] \\ \rightarrow 1/6[\bar{1}\bar{1}2] + 1/6[12\bar{1}] \end{cases}$$

The upper case gives values of  $n_{1,2} = \pm 1$  and the lower case  $n_{1,2} = \pm 1/3$ .

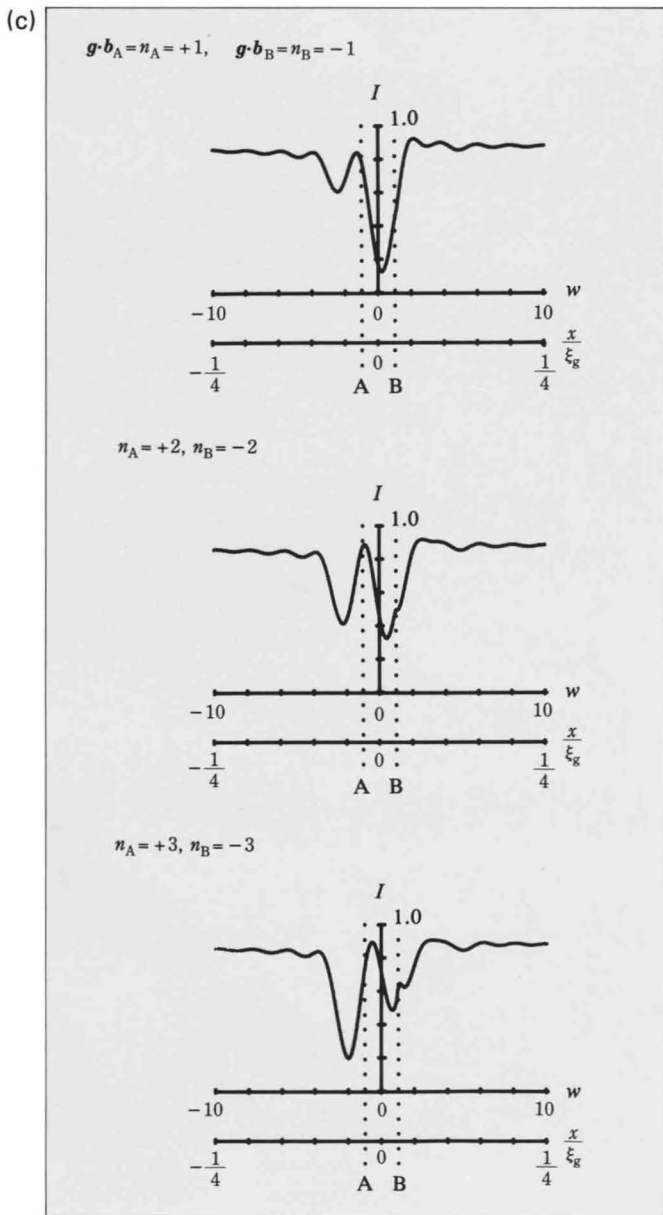
Figure (b) shows a rocking curve for a perfect crystal as a reference. Figure (c) shows rocking curves from an extended screw dislocation for three different values of  $n_A (= n_1)$  and  $n_B (= n_2)$ . Two partials are located at the positions A and B. The exact Bragg position is at the middle of two partials. Figure (d) shows the rocking curves for  $n_A = +1$  and  $n_B = -1$  ( $n_{1,2} = \pm 1$ ) at three different

Bragg settings with respect to the position of the extended dislocation. The profile of Photo (a) appears to have values of  $n_{1,2} = \pm 1$ , indicating the upper case of dissociation, because if  $n_{1,2} = \pm 1/3$ , the weaker peak should be much weaker than the observed one.

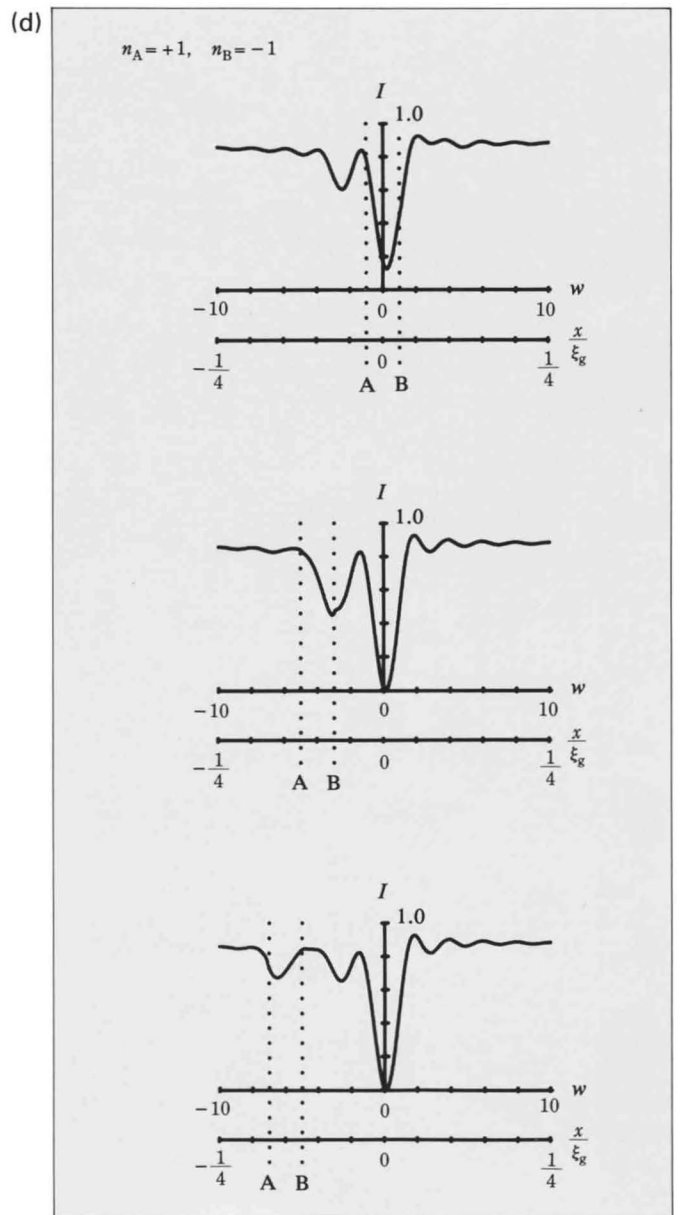




$$\frac{t}{\xi_g} = \frac{1}{2}$$



$$\frac{t}{\xi_g} = \frac{1}{2}, \quad y = \frac{t}{2}, \quad g \cdot b = n = 0$$



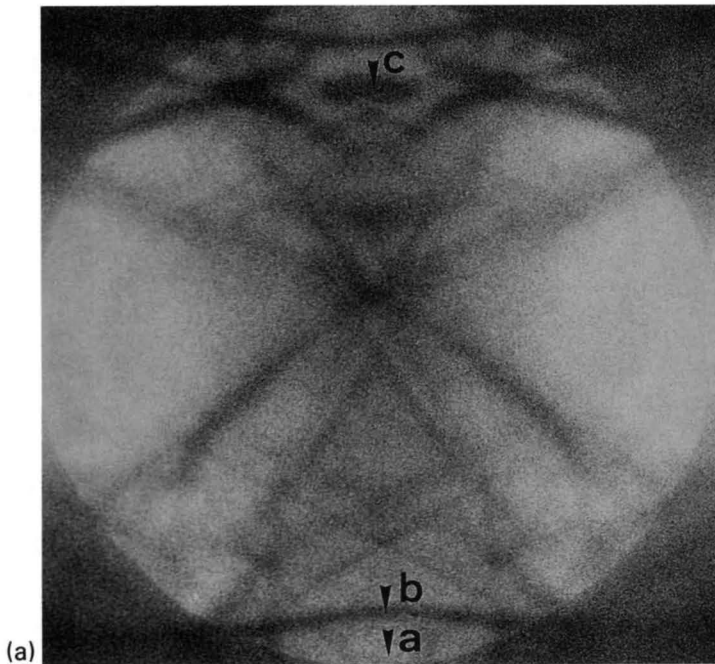
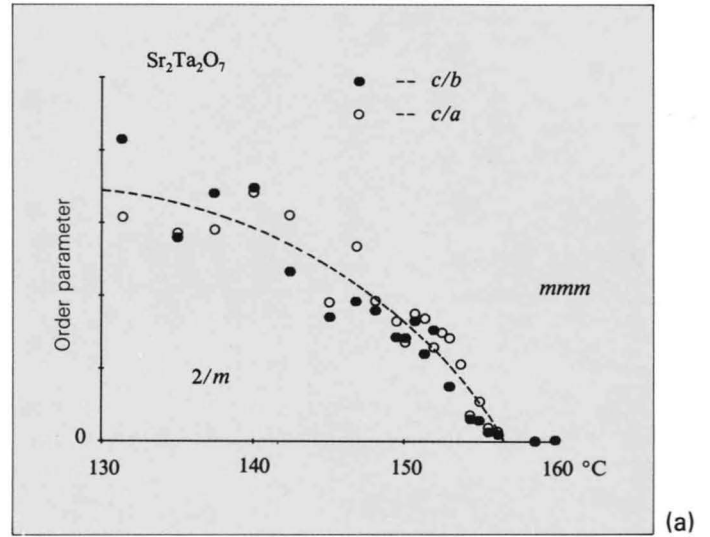
$$\frac{t}{\xi_g} = \frac{1}{2}, \quad y = \frac{t}{2}, \quad g \cdot b = n = 0$$

# *Applications*

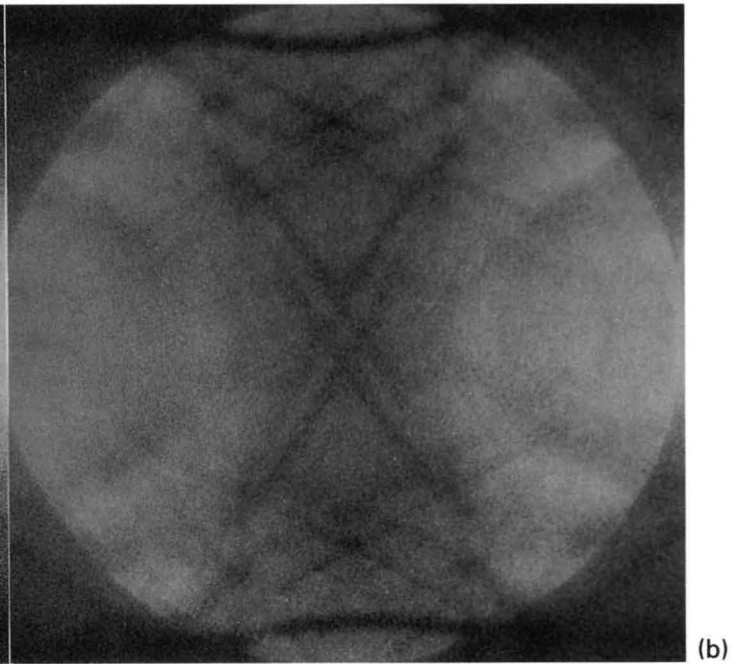
# Determination of Order Parameters

## $\text{Sr}_2\text{Ta}_2\text{O}_7$

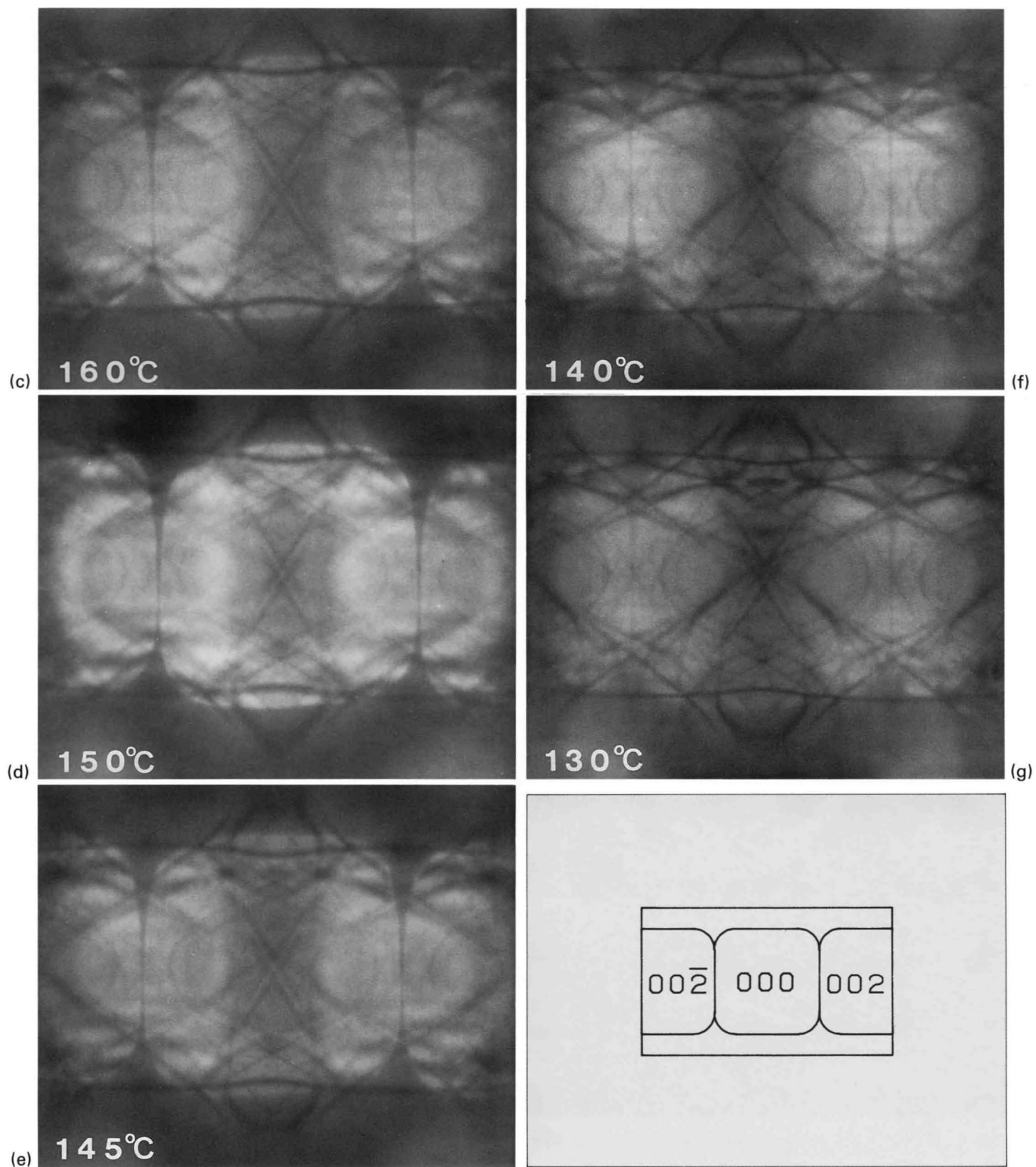
$\text{Sr}_2\text{Ta}_2\text{O}_7$  undergoes a second-order phase transition at  $158^\circ\text{C}$  from the high temperature phase belonging to a space group  $Cmcm$  to the low temperature phase belonging to  $P2_1/m$ . A series of Photos, (c) to (g), shows the temperature dependence of the bright-field CBED patterns. A vertical mirror symmetry exists in all the patterns. The horizontal mirror symmetry seen in Photo (c) gradually vanishes with decreasing temperature. The bright-field CBED patterns (a) and (b) were taken above and below the transition temperature. The intensities of the background a and the HOLZ lines b remain almost the same between Photos (a) and (b). The HOLZ line c is greatly different between the two photos. Thus, the HOLZ line b must be fundamental reflections and the line c must be a reflection directly related with the phase transition. The intensity of the line c was normalized by the intensities of the background a and the line b. The square of the normalized intensity was plotted as a function of temperature as shown in the diagram. It is seen that the value of the order parameter of the low temperature phase increases with decreasing temperature.



Point group  $2/m$

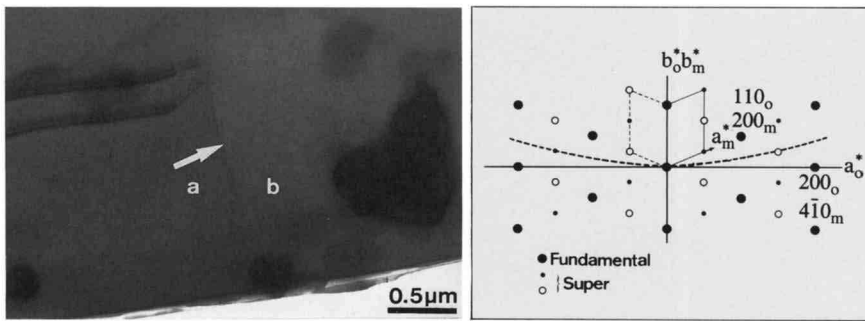


Point group  $mmm$

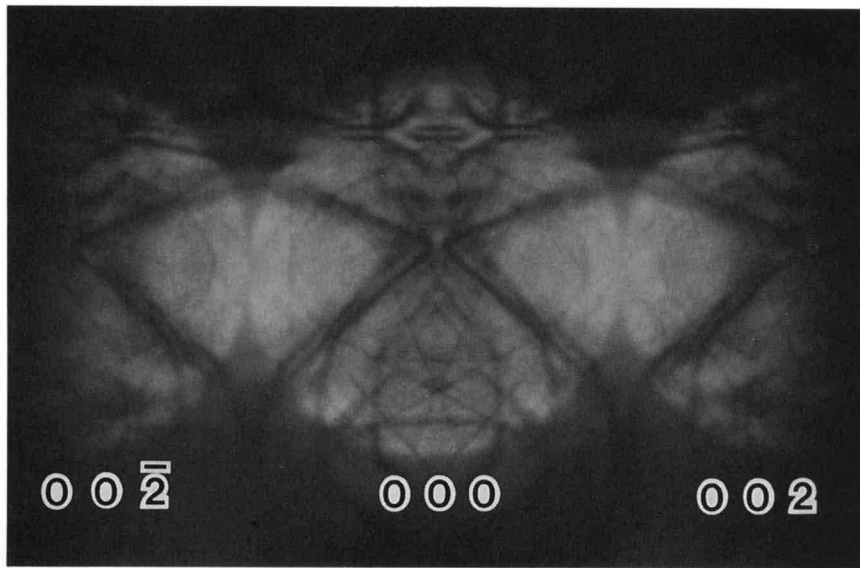


# Observation of Domains

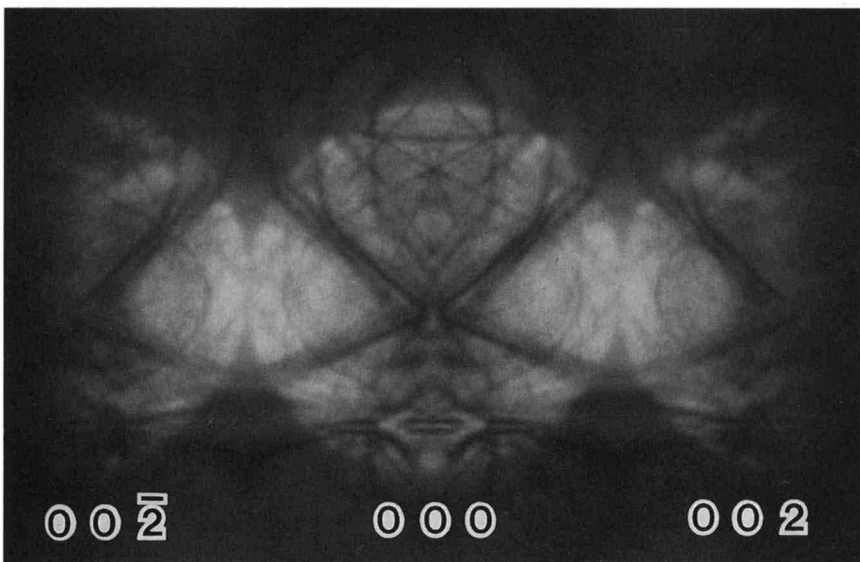
$\text{Sr}_2\text{Ta}_2\text{O}_7$



100 kV



(a)



(b)

$\text{Sr}_2\text{Ta}_2\text{O}_7$

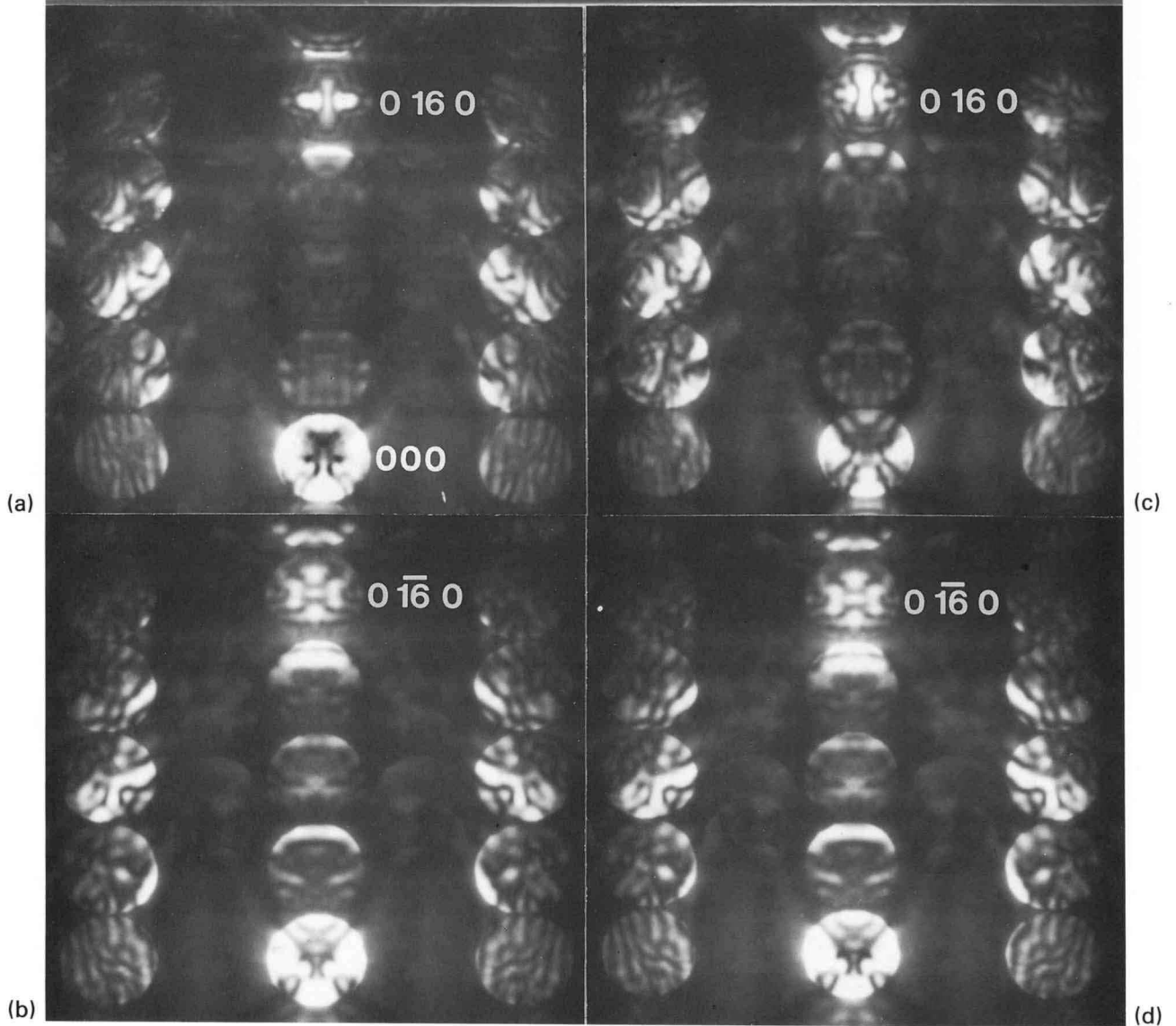
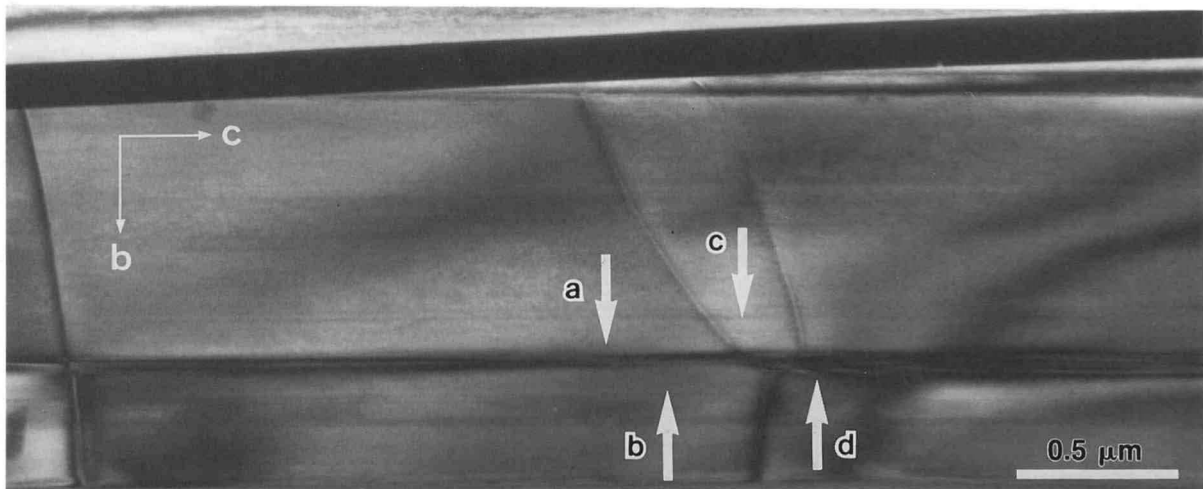
The electron micrograph of  $\text{Sr}_2\text{Ta}_2\text{O}_7$ , taken at an incidence parallel to the  $b$  axis, shows a contrast due to twin domains a and b. At this incidence, however, the contrast is very weak, because the ZOLZ reflections (fundamental) are common to both domains and only HOLZ reflections (superlattice) give difference between them. The diffraction spots in the  $a_0^*-b_0^*$  plane expected from the twin structure are depicted in the diagram. The reciprocal lattice cell drawn by the solid line corresponds to one domain and the cell drawn by the dotted line to the other domain.

The CBED patterns (a) and (b) were taken from the domains a and b, respectively. HOLZ lines appear with a strong contrast at opposite positions to each other between the two patterns. These patterns have revealed that the sense of the  $b_0^*$  axis of one domain is opposite to that of the other domain.

$\text{TaS}_3$



The CBED patterns (a), (b), (c) and (d) were taken at a common incidence respectively from the four domains a, b, c and d in the electron micrograph of  $\text{TaS}_3$ . The exactly excited reflections in (a) and (c) were found to have the same index,  $0\ 1\ 6\ 0$ , although they show a little different patterns due to the difference of thickness. The exactly excited reflections in (b) and (d) show very similar patterns and have the same index,  $0\ \bar{1}\ 6\ 0$ . These results have revealed that the sense of the  $b$  axes in the domains b and d is opposite to that in domains a and c, and that a certain displacement exists along the  $b$  direction between the domains a and c, and between the domains b and d.

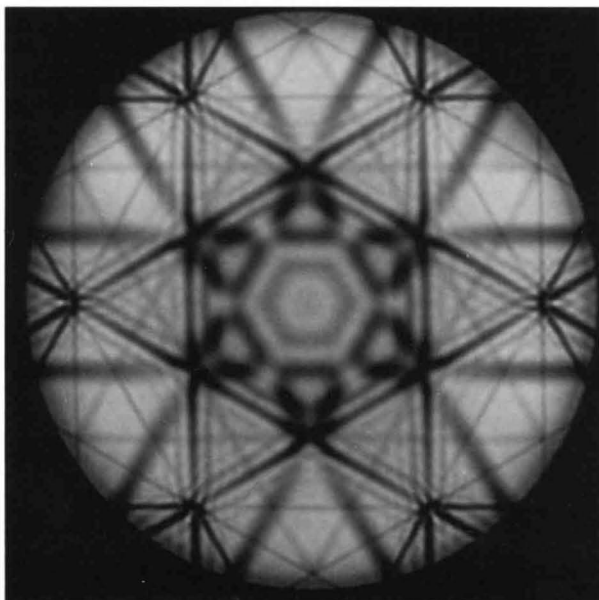
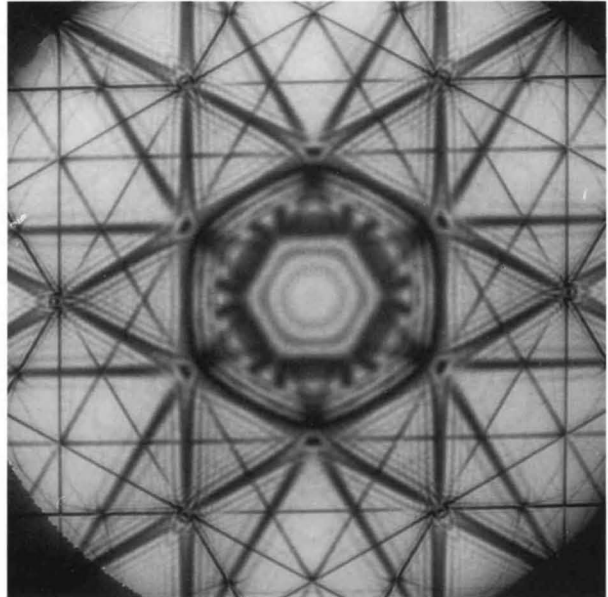
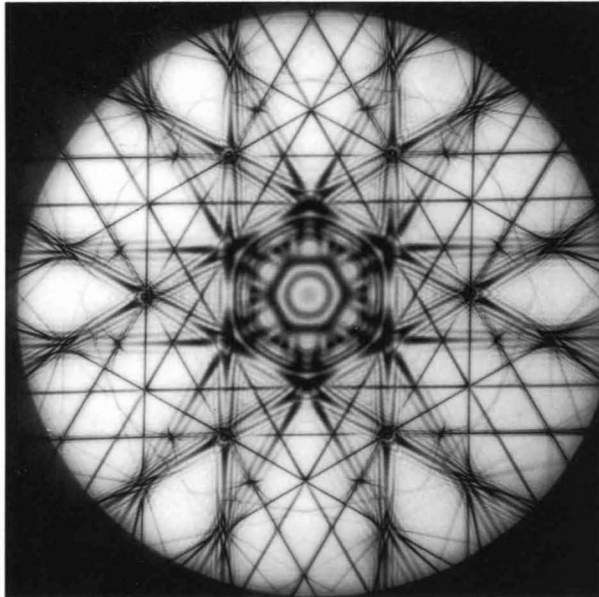


# LACBED Patterns

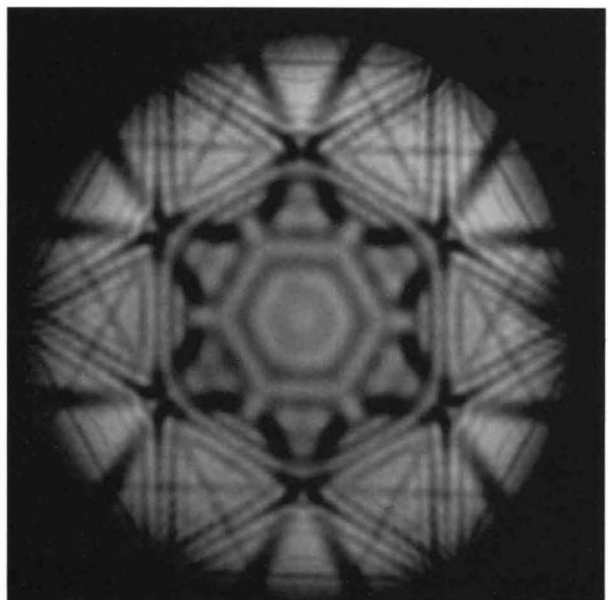
Graphite (perfect) [0001]

200 kV

80 kV



60 kV

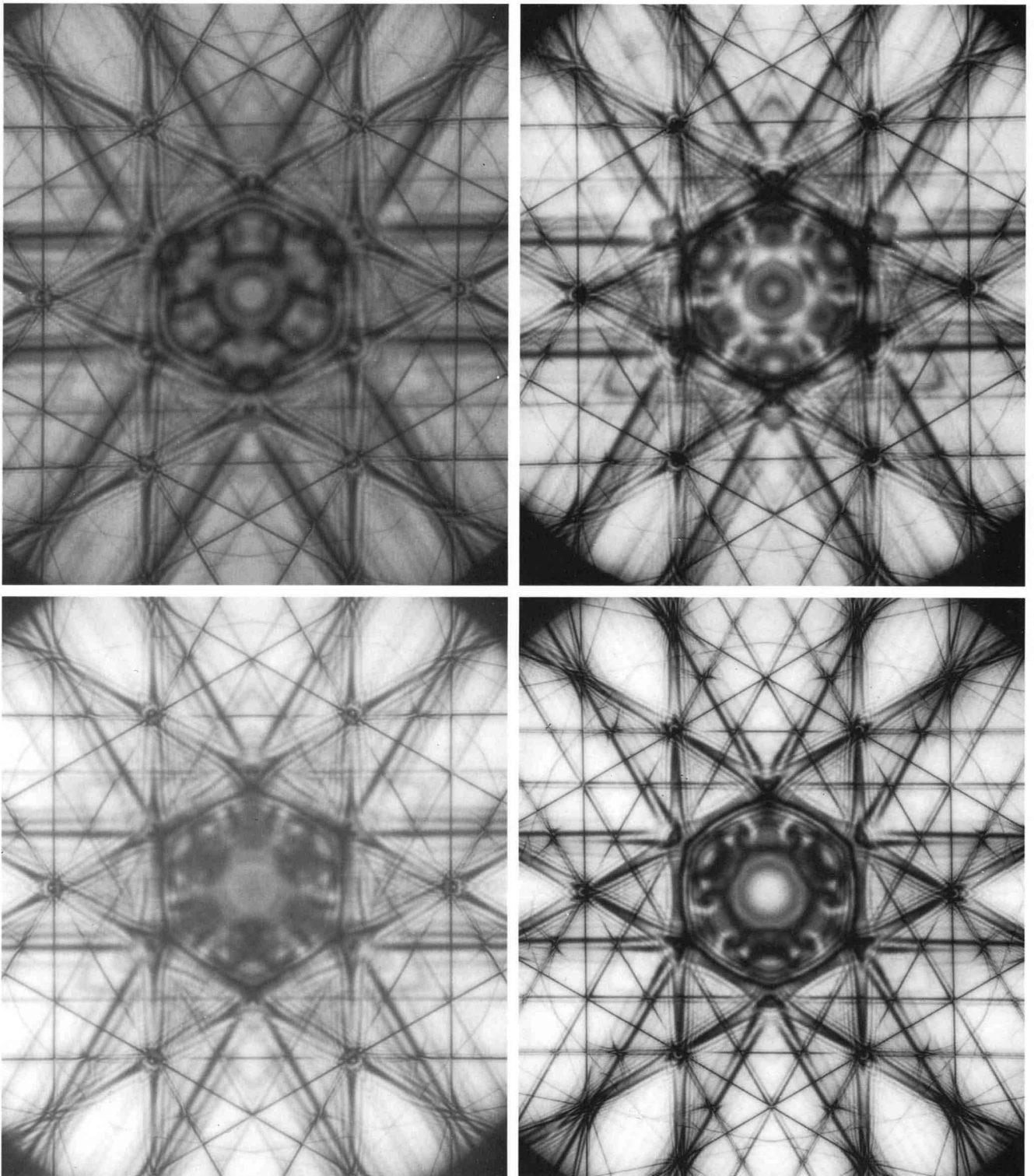


40 kV

Bright-field LACBED patterns showing symmetries of  $6mm$  taken from a perfect area of graphite at four different accelerating voltages with the camera length kept constant.

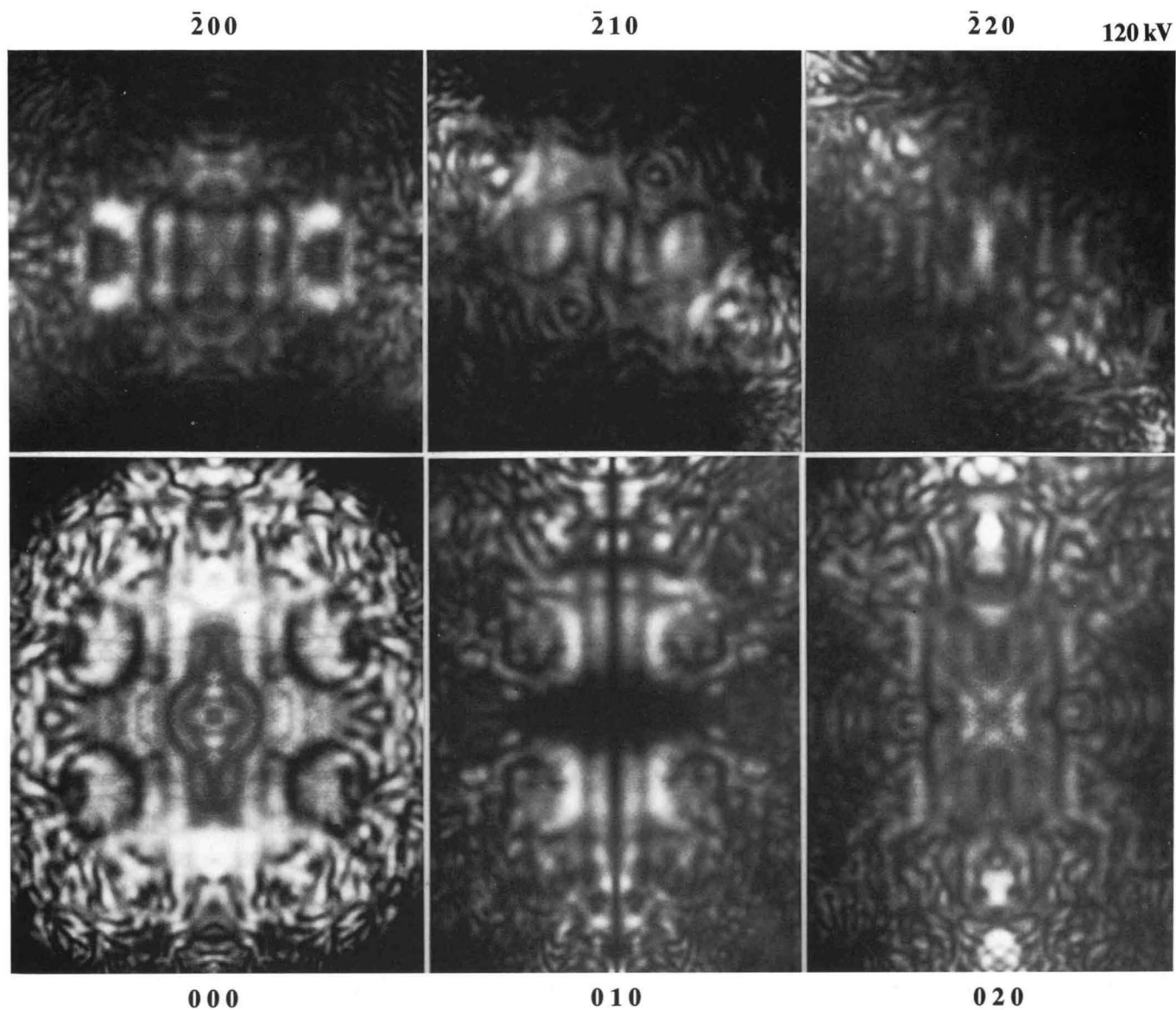
**Graphite (stacking fault) [0001]**

200 kV

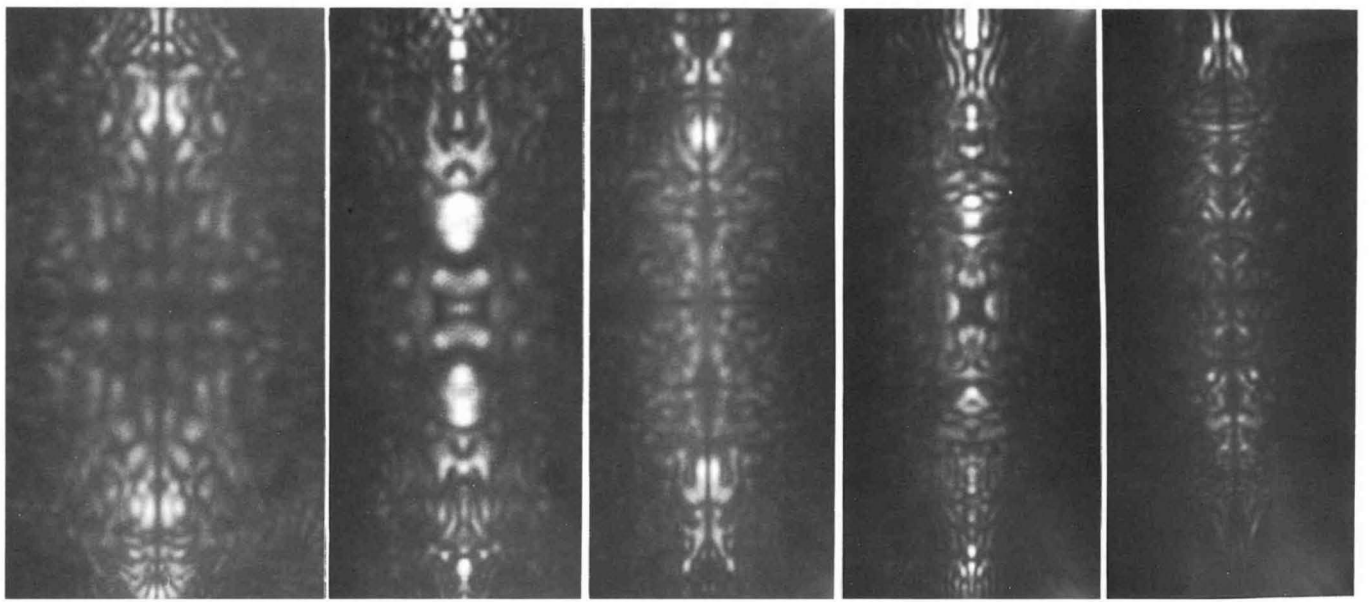


Bright-field LACBED patterns showing symmetries of  $3m$  taken from four different areas containing stacking faults, the difference between the patterns being due to the numbers and positions of fault planes.

**FeS<sub>2</sub> [001]**



A set of LACBED patterns taken from FeS<sub>2</sub> at the [001] incidence. GM lines due to a 2<sub>1</sub> screw axis and a *b*-glide plane are seen in the 0*k*0 (*k*=odd) patterns. Symmetries of 1<sub>R</sub> and 2*mm* formed by ZOLZ and HOLZ interactions are clearly seen in the  $\bar{2}10$  &  $\bar{2}20$  patterns and in the other patterns, respectively.



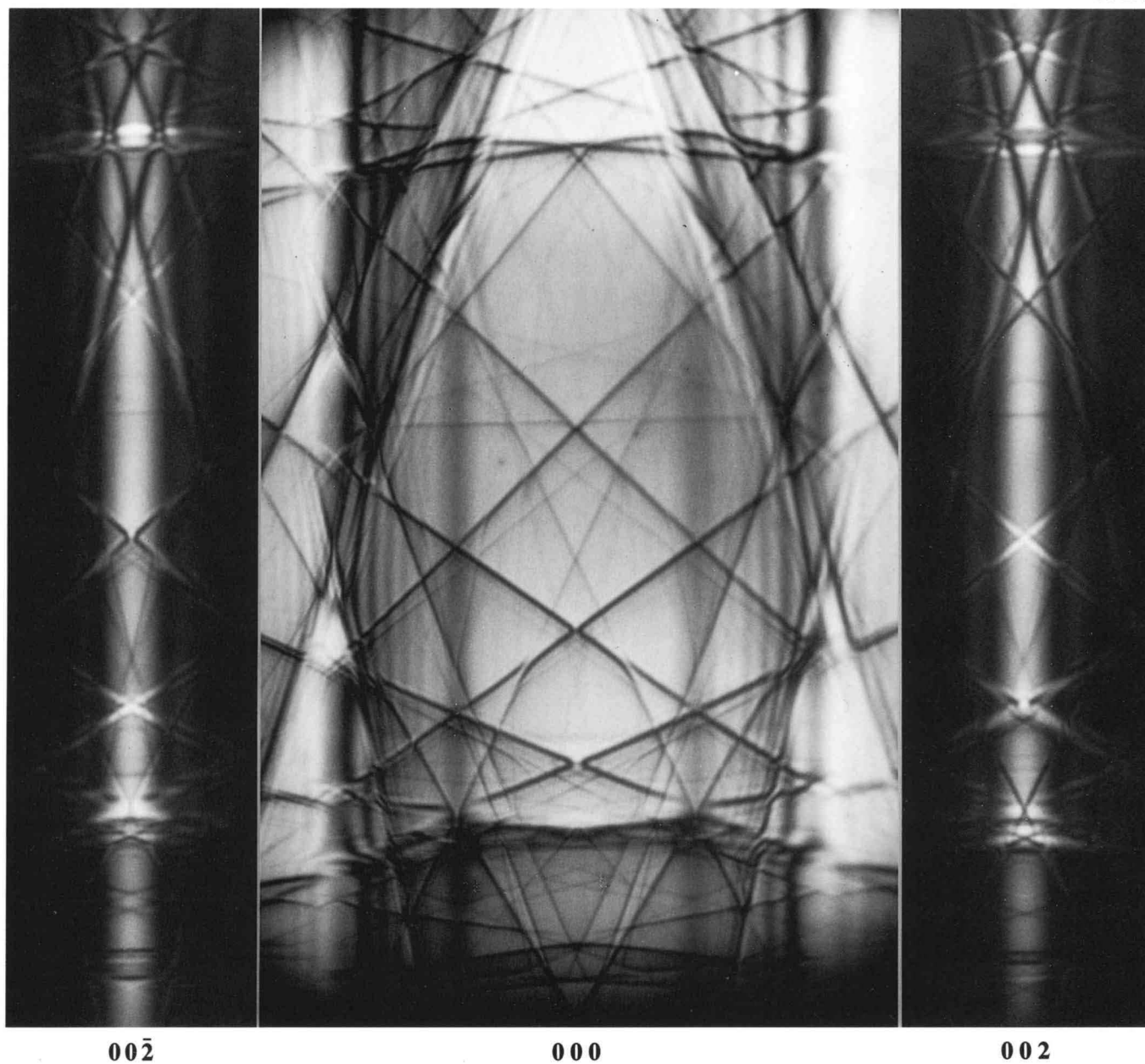
030

040

050

060

070

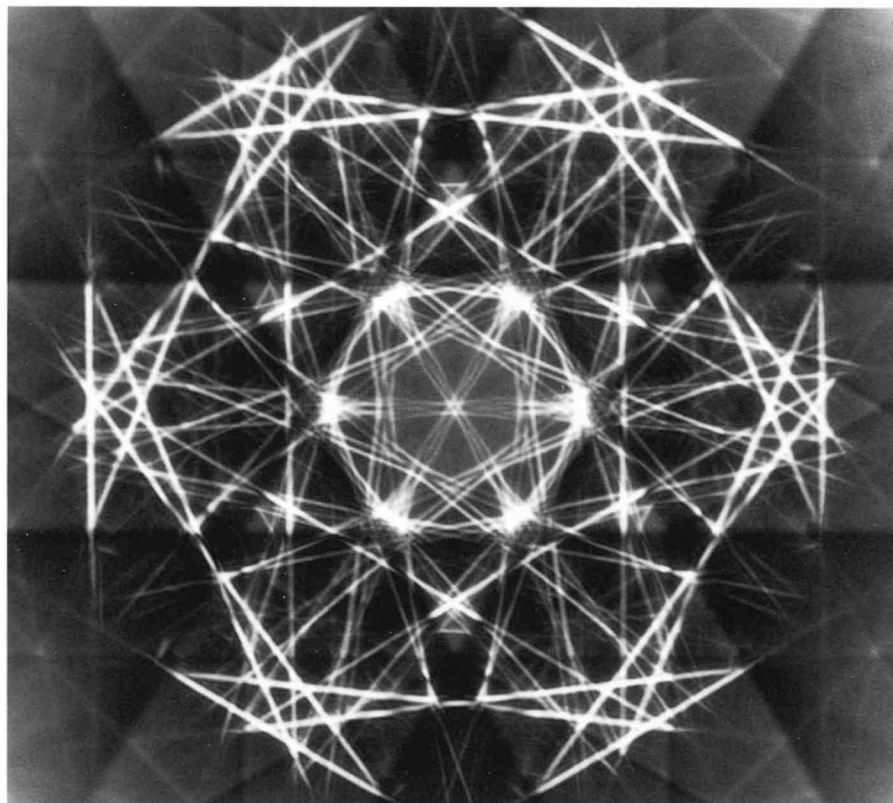


The  $000$ ,  $002$  and  $00\bar{2}$  LACBED patterns taken at the  $[10\ 1\ 0]$  incidence. The lack of a symmetry of  $2_R$  is clearly seen over a wide angular range in the pair of patterns,  $002$  and  $00\bar{2}$ .

# Hollow-Cone Beam CBED Patterns

Graphite [0001]

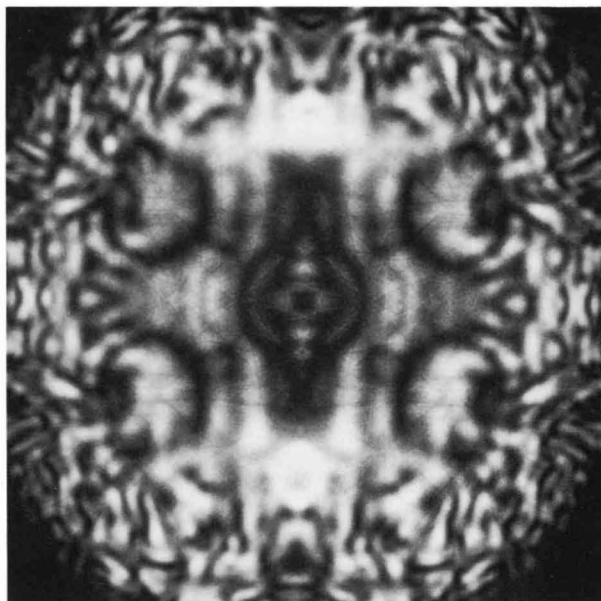
200 kV



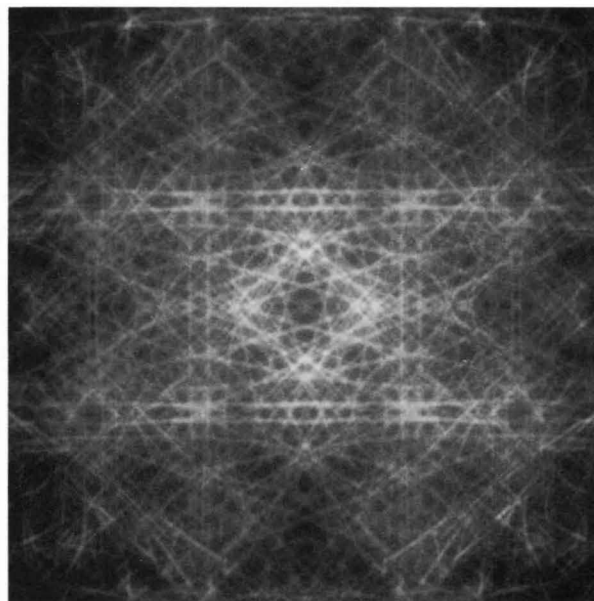
FOLZ

FeS<sub>2</sub> [001]

120 kV



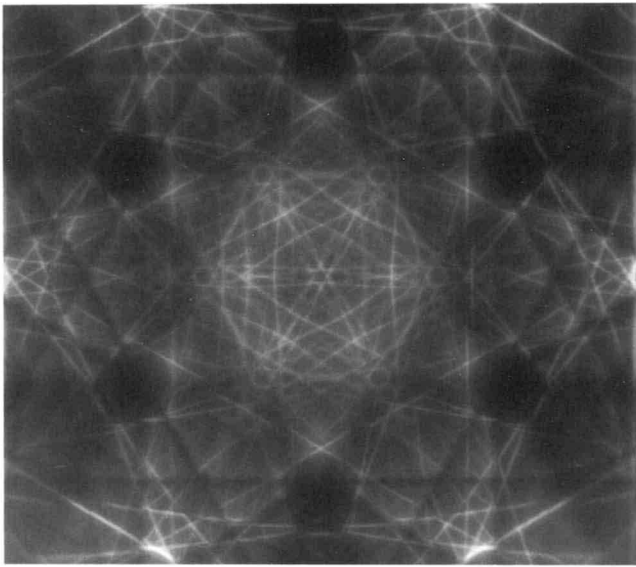
LACBED



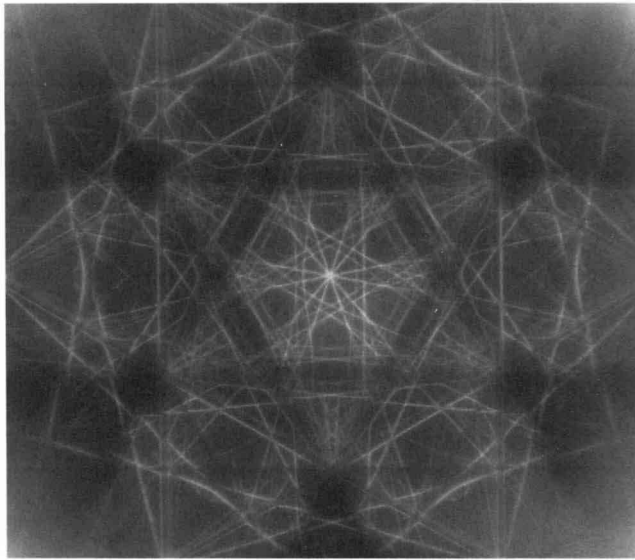
FOLZ

Note that symmetries due to HOLZ lines are clearly seen in the hollow-cone beam CBED patterns.

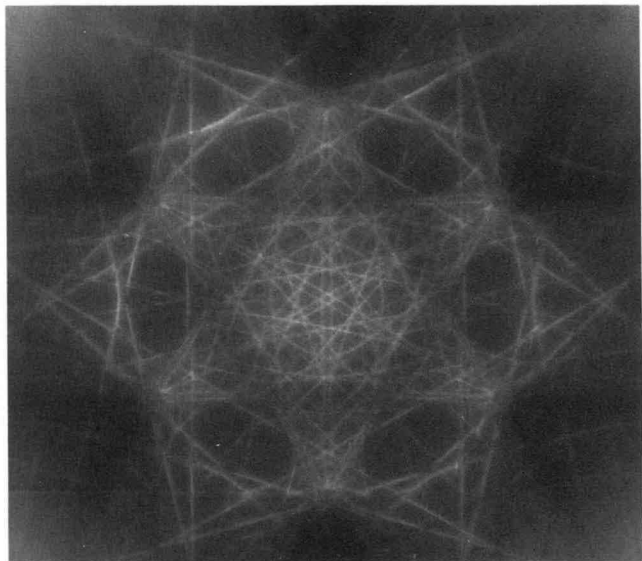
SiC-6H [0001] FOLZ



200 kV

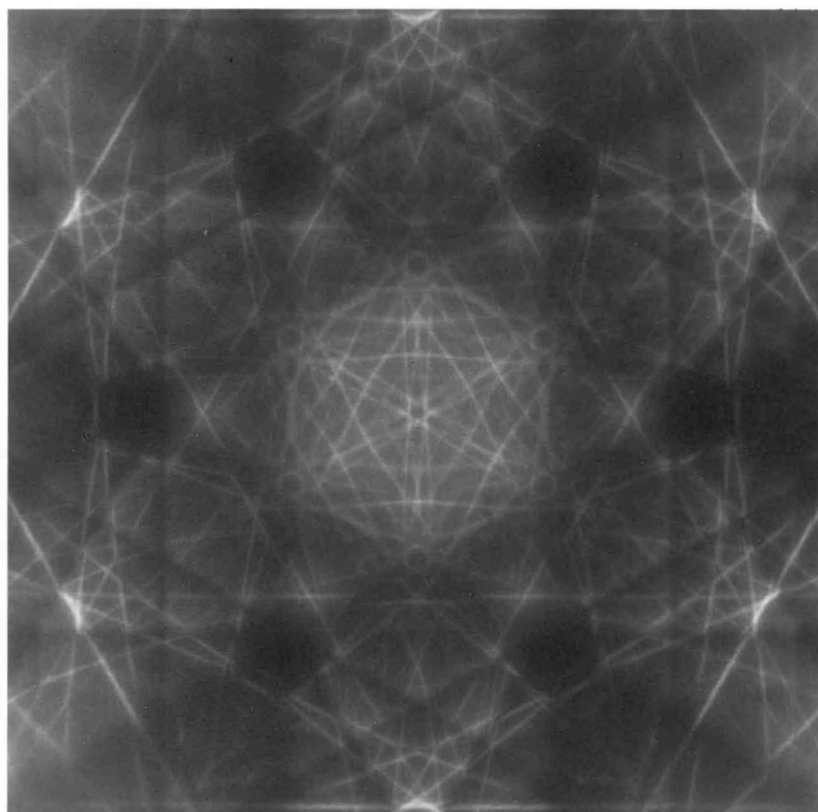


120 kV

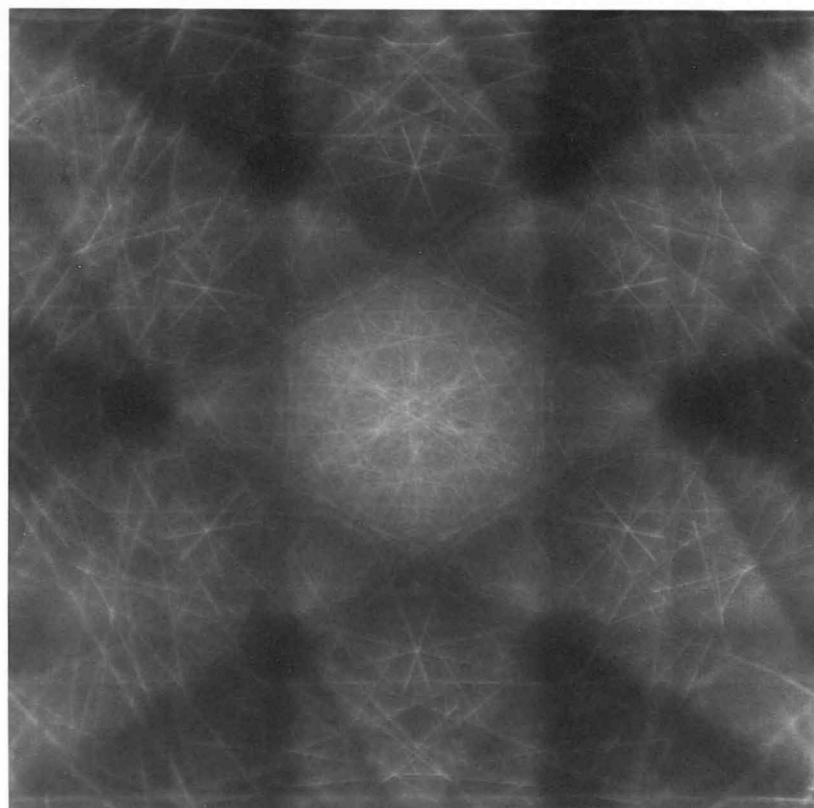


100 kV

SiC-6H [0001] 200 kV



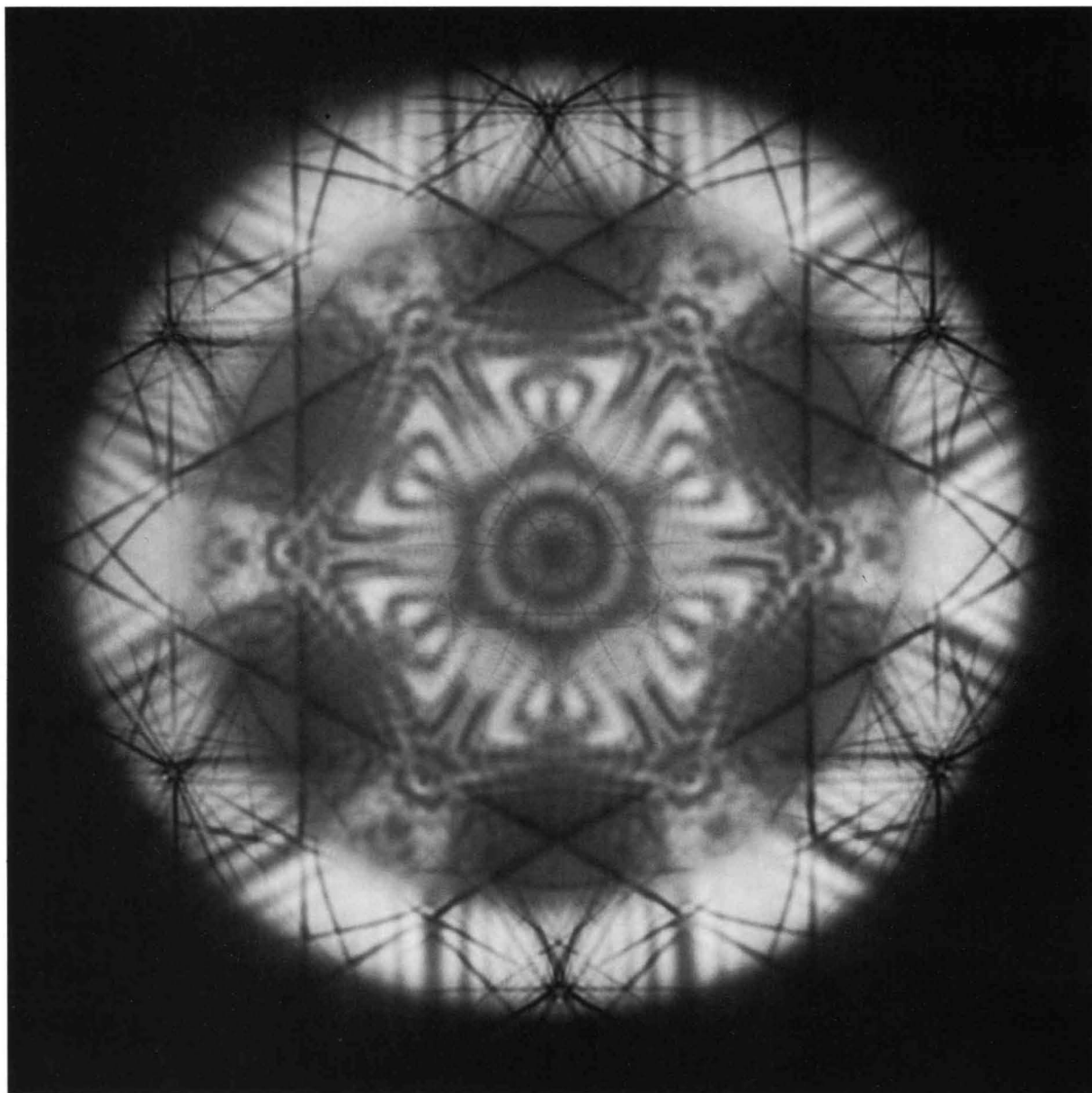
FOLZ

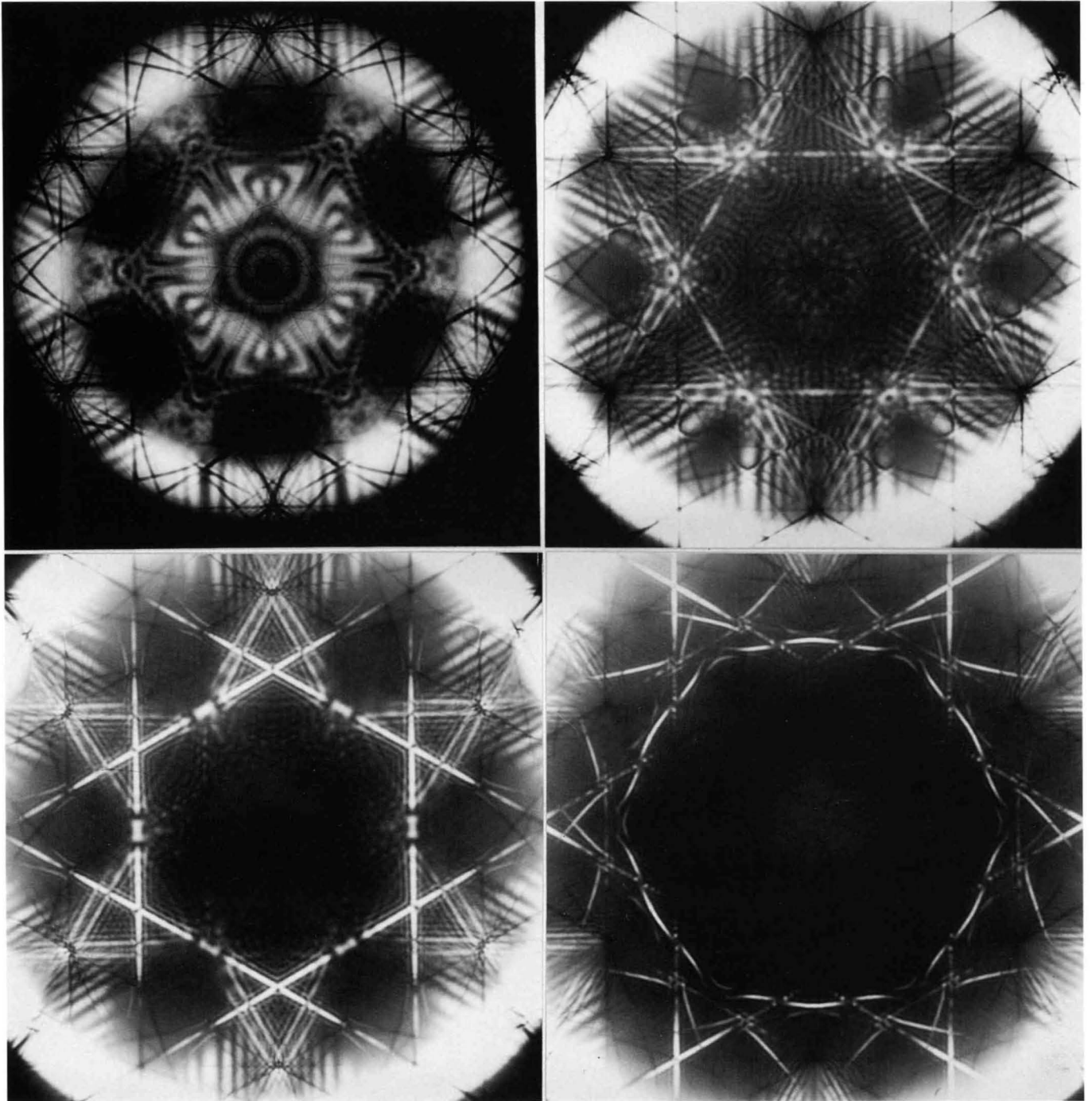


SOLZ

Si [111]

100 kV



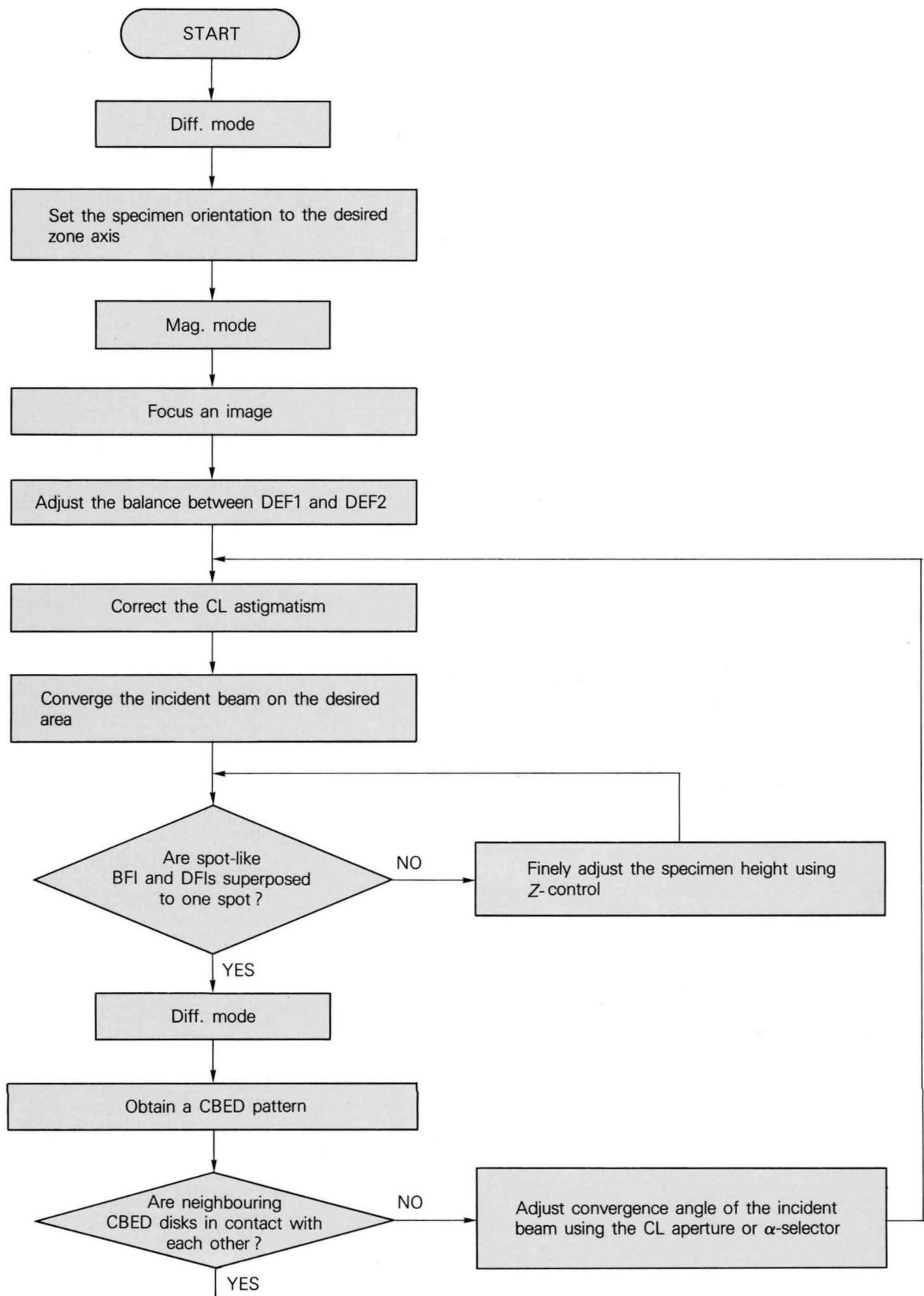


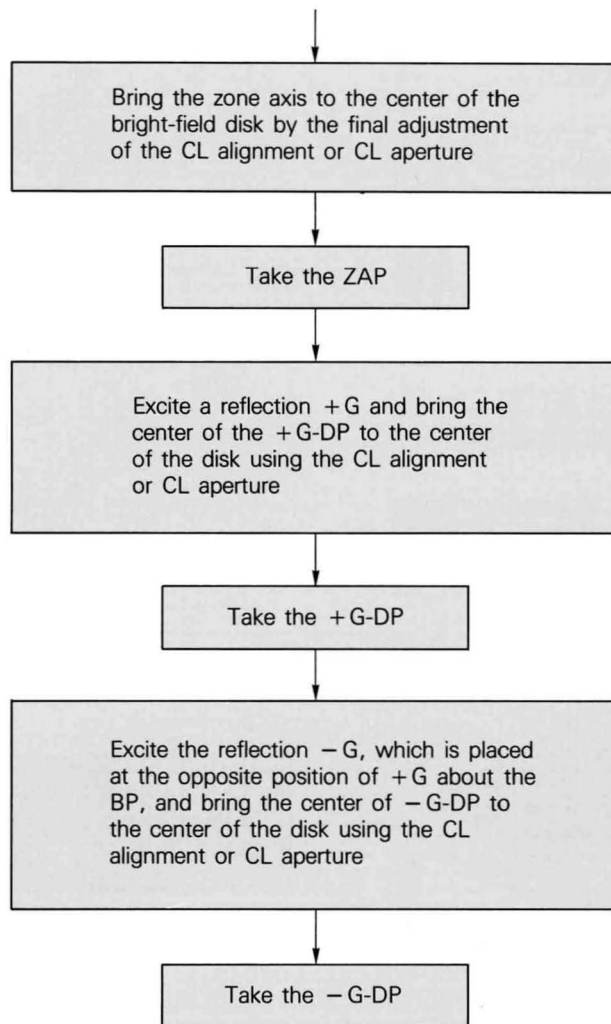
A series of hollow-cone beam CBED patterns taken from (111)Si at four different settings of the hollow-cone beam angle.

# *Appendices*

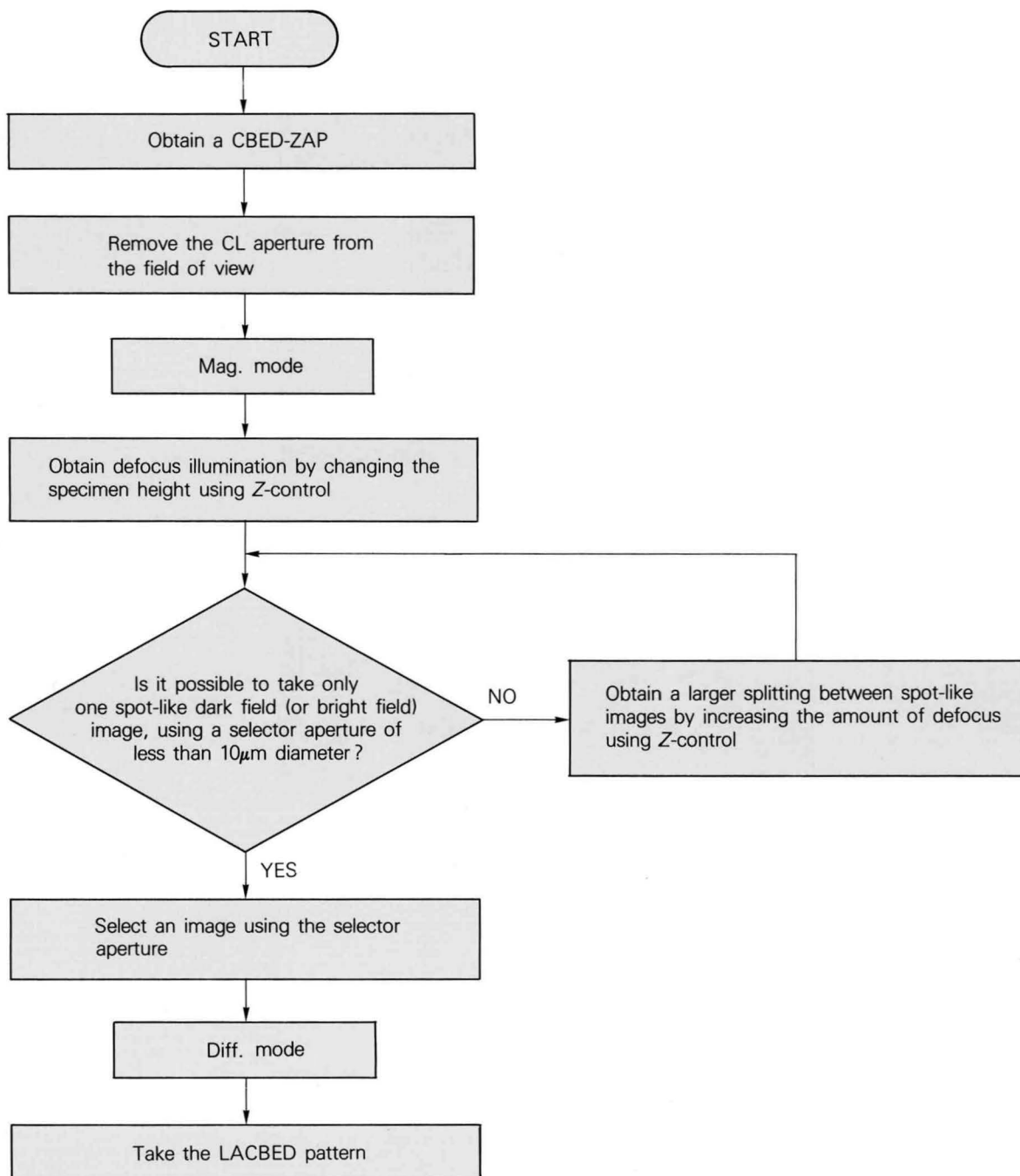
# Flow Charts

## CBED pattern





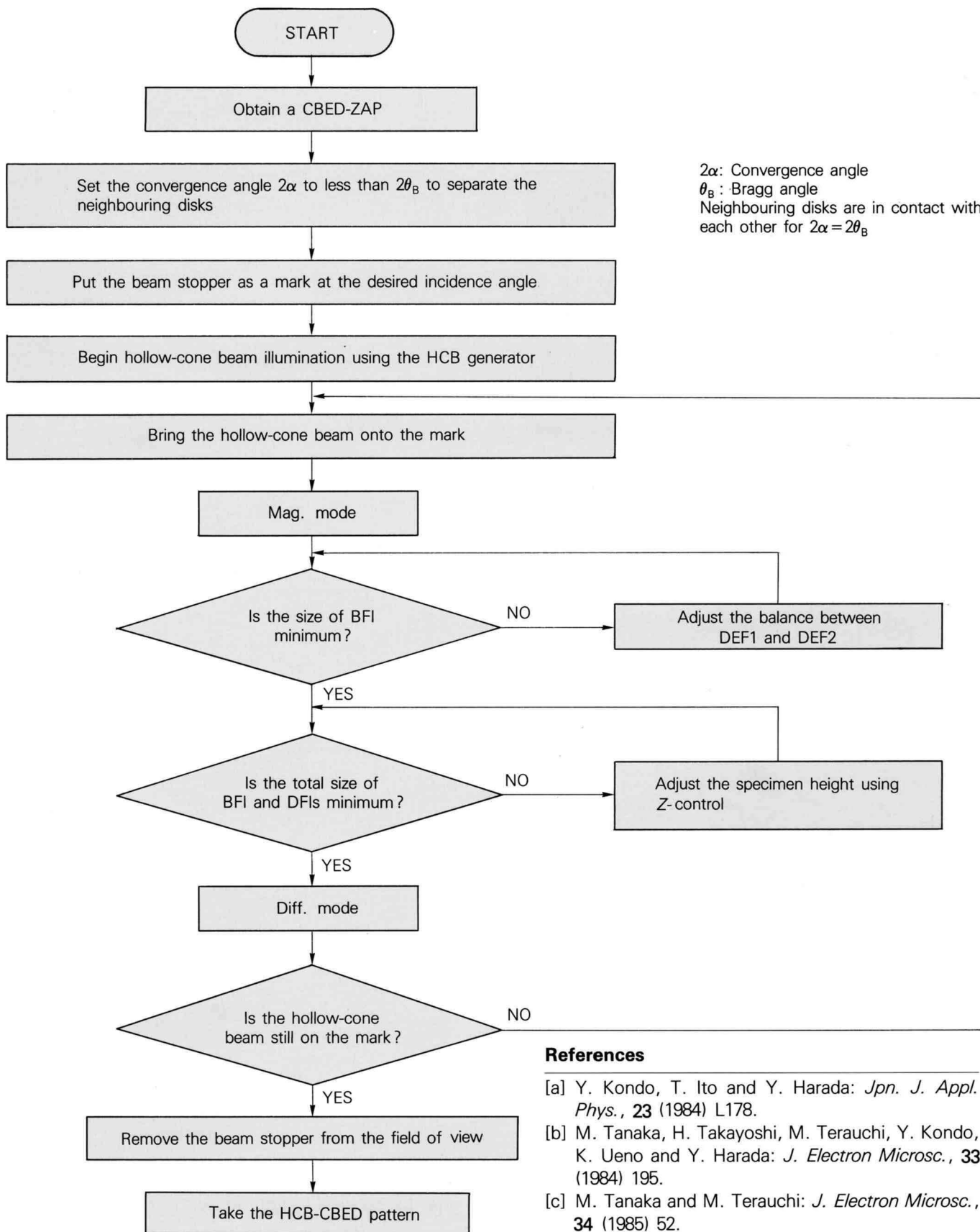
## Large-angle CBED pattern (LACBED)



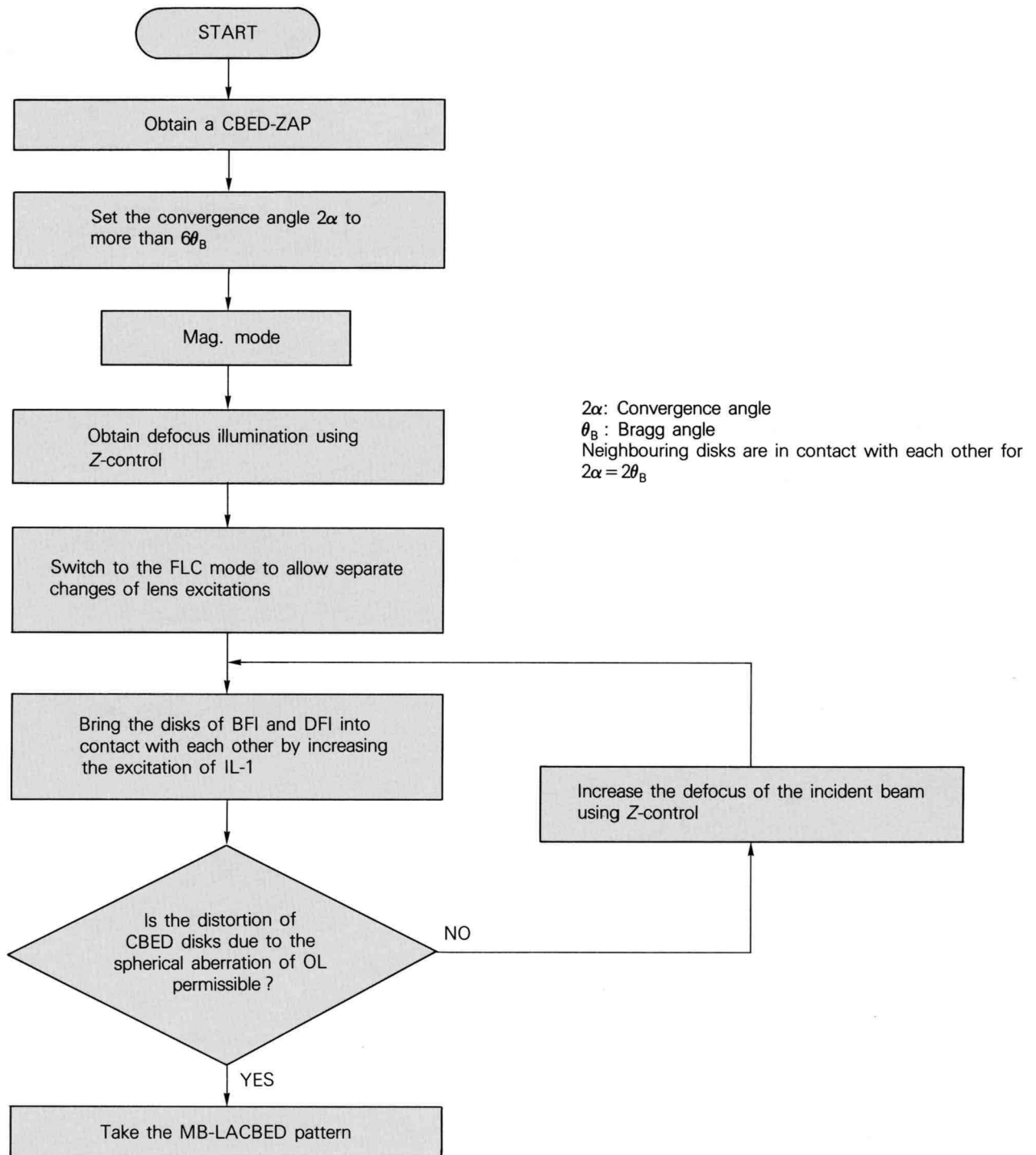
### Reference

- [a] M. Tanaka, R. Saito, K. Ueno and Y. Harada: *J. Electron Microsc.*, **29** (1980) 408.

## Hollow-cone beam CBED (HCB-CBED) pattern



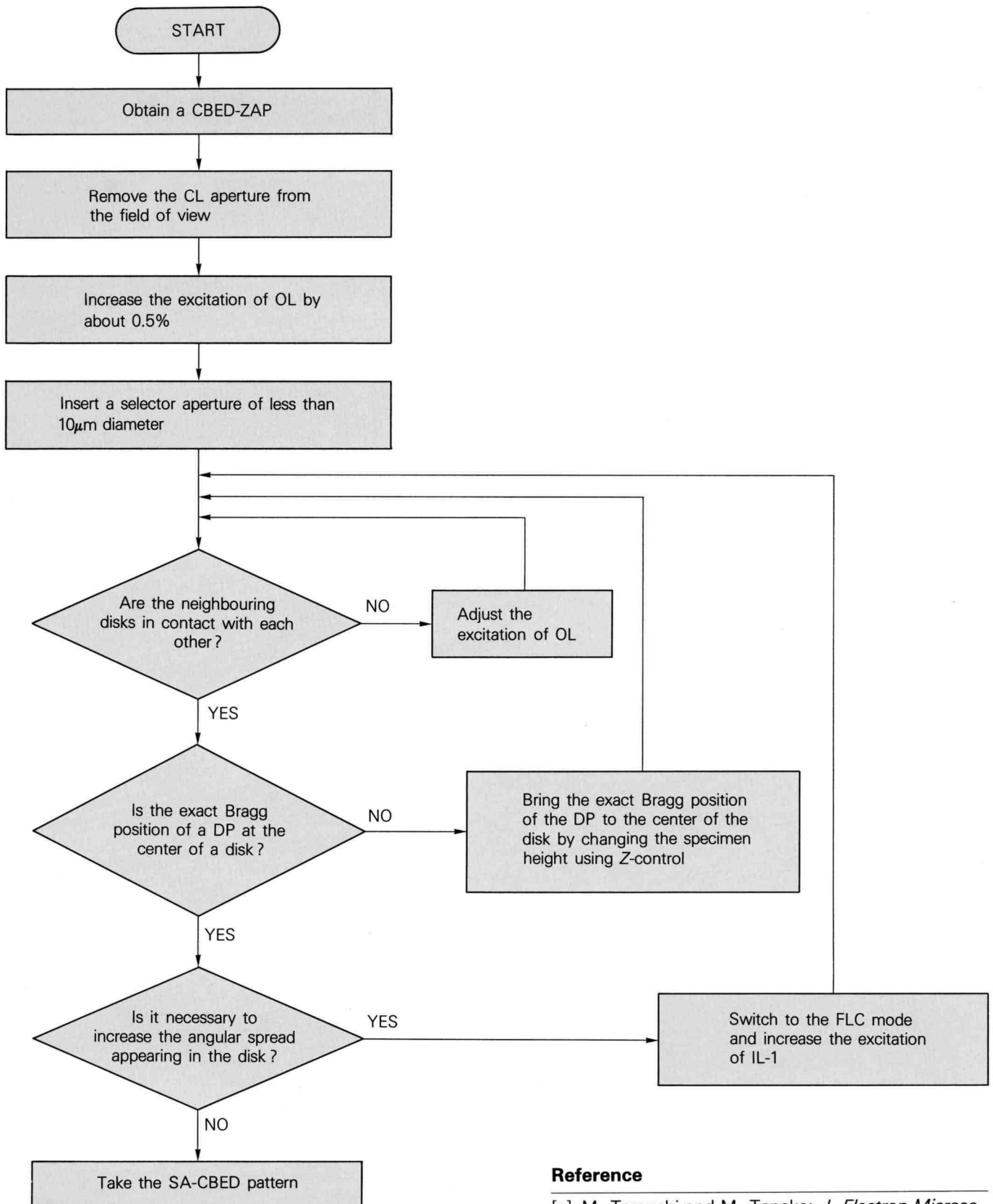
## Many-beam LACBED pattern (MB-LACBED)



### Reference

- [a] M. Terauchi and M. Tanaka: *J. Electron Microsc.*, **34** (1985) 128.

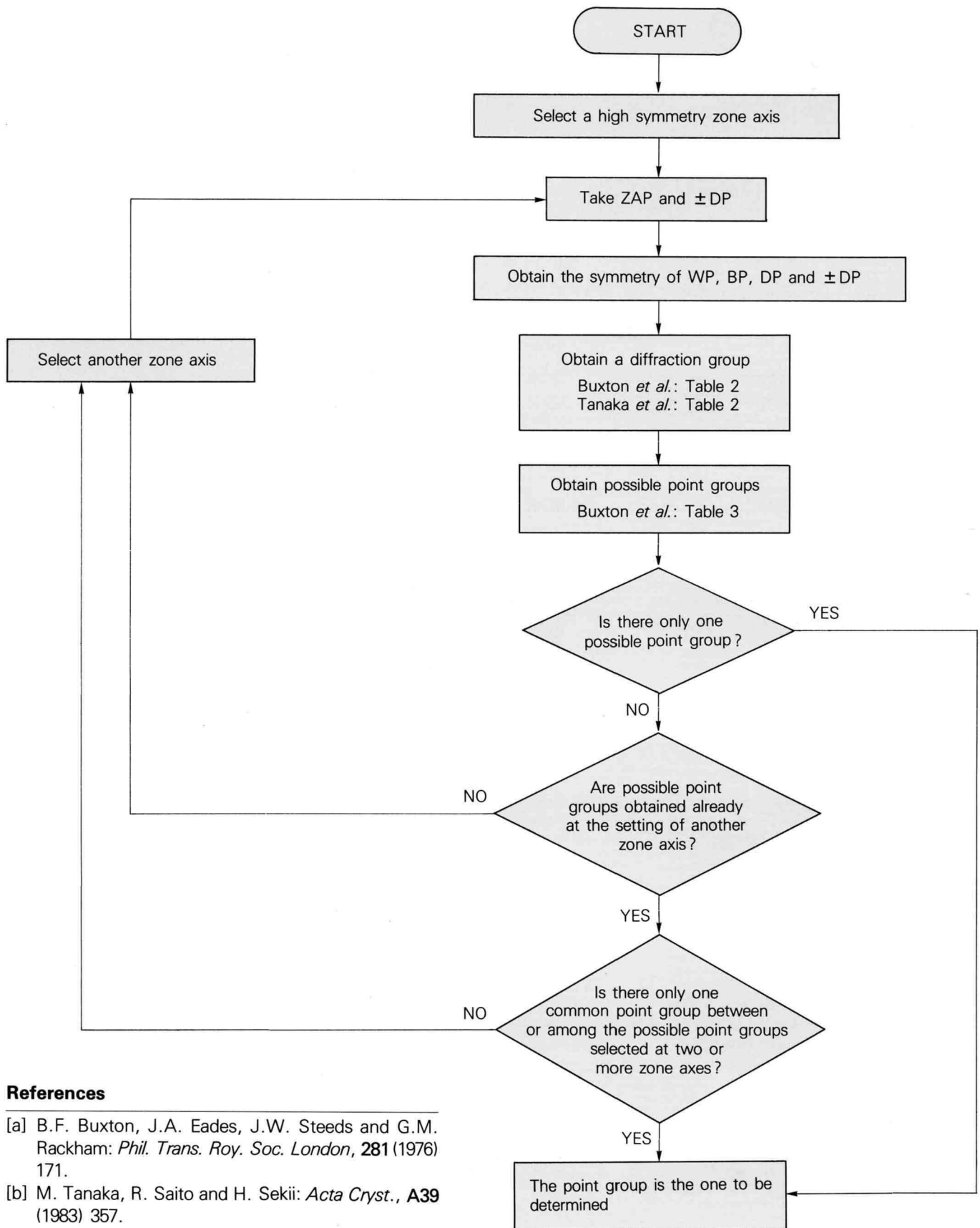
## Selected area CBED pattern (SA-CBED)



### Reference

- [a] M. Terauchi and M. Tanaka: *J. Electron Microsc.*, **34** (1985) 347.

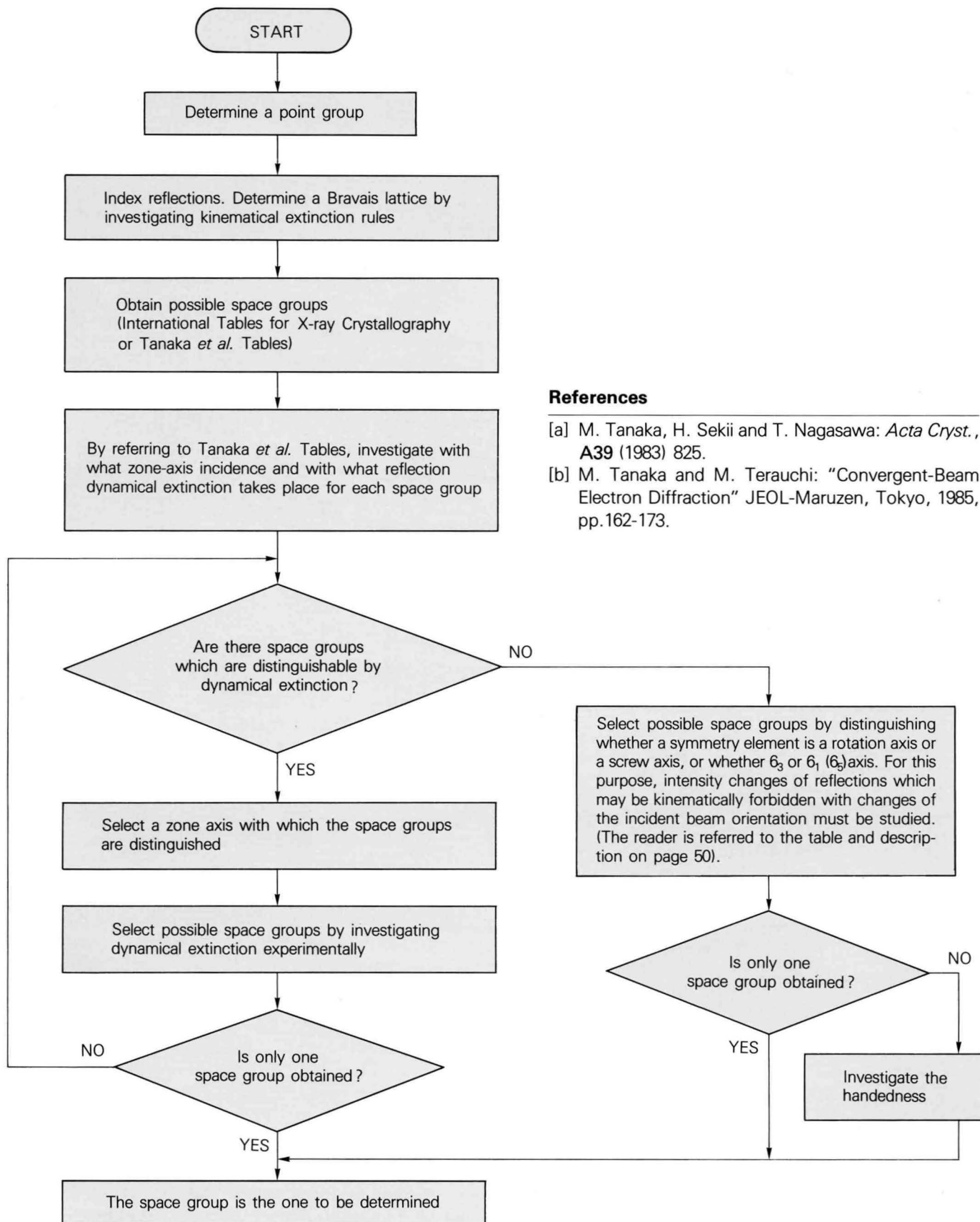
# Point-group determination



## References

- [a] B.F. Buxton, J.A. Eades, J.W. Steeds and G.M. Rackham: *Phil. Trans. Roy. Soc. London*, **281** (1976) 171.  
 [b] M. Tanaka, R. Saito and H. Sekii: *Acta Cryst.*, **A39** (1983) 357.

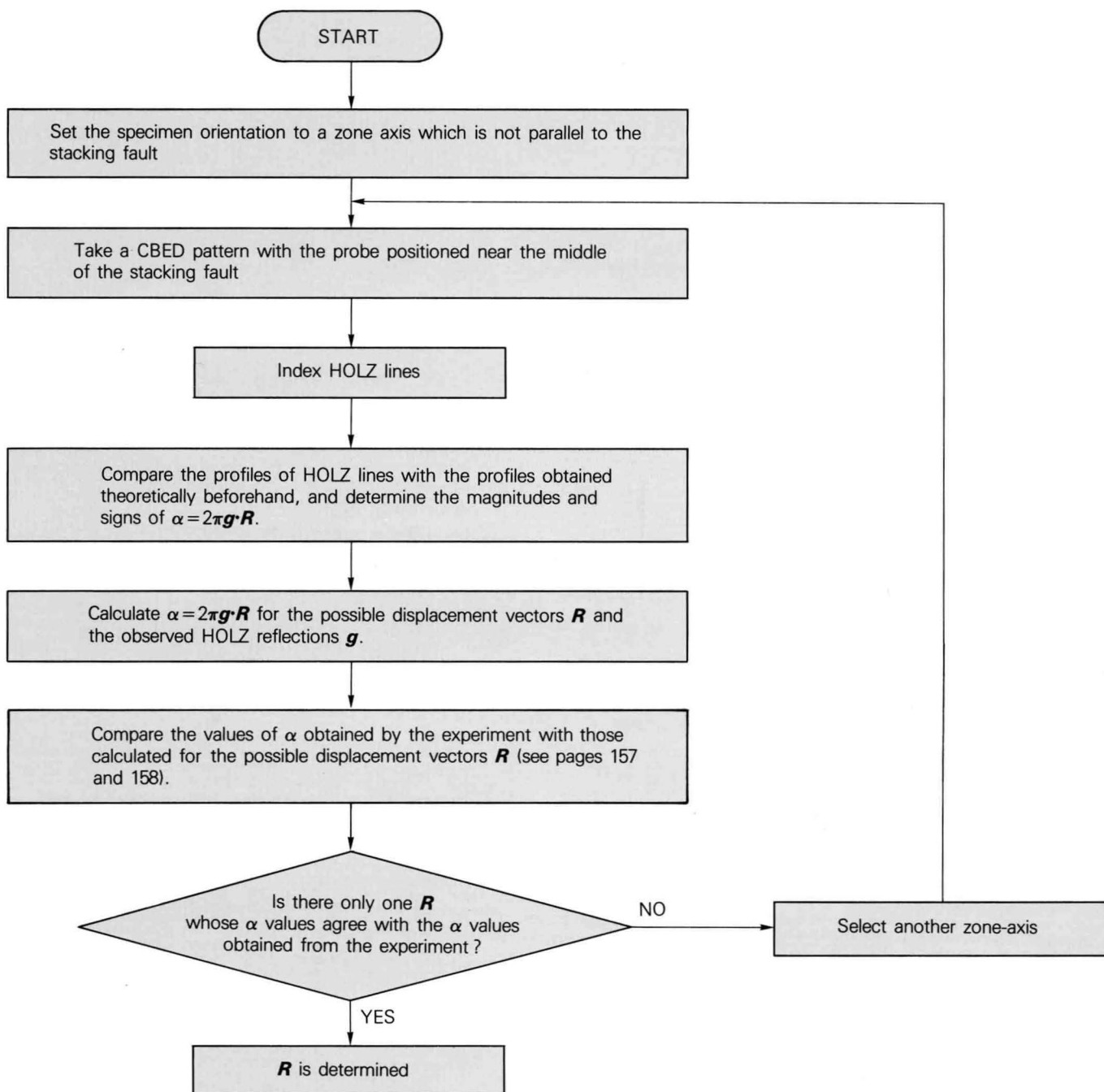
# Space-group determination



## References

- [a] M. Tanaka, H. Sekii and T. Nagasawa: *Acta Cryst.*, **A39** (1983) 825.
- [b] M. Tanaka and M. Terauchi: "Convergent-Beam Electron Diffraction" JEOL-Maruzen, Tokyo, 1985, pp.162-173.

## Determination of the displacement vector $R$ of a stacking fault



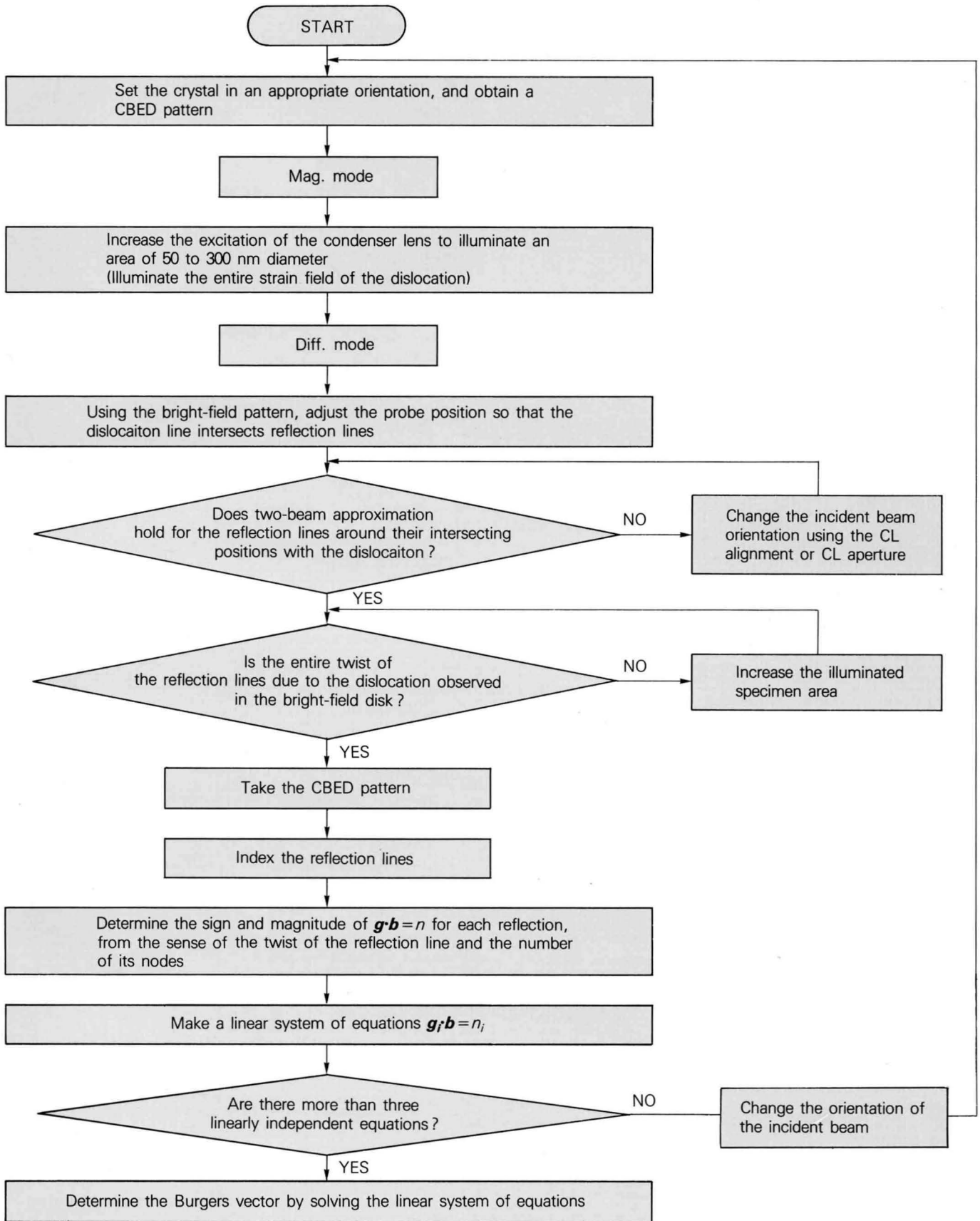
### Reference

[a] M. Tanaka and T. Kaneyama: Proc. XIth Int. Congr. on Electron Microsc., Kyoto, 1986, p. 203.

### References

- [a] D. Cherns and A.R. Preston: Proc. XIth Int. Congr. on Electron Microsc., Kyoto, 1986, P. 721.  
 [b] M. Tanaka: *J. Electron Microsc.*, **35** (1986) 314.

## Determination of the Burgers vector $b$ of a dislocation



# Tables of GM Lines in HOLZ Reflections for Space-Group

## Point groups $m, 2/m$

Incident beam direction	[u0w]		Incident beam direction	[u0w]	
Space group			Space group		
6 $Pm$			11 $P2_1/m$		
7 $Pc$	$h0l_0$ $c$	$A_h$	12 $C2/m$		
8 $Cm$			13 $P2/c$	$h0l_0$ $c$	$A_h$
9 $Cc$	$h_00l_0$ $c$	$A_h$	14 $P2_1/c$	$h0l_0$ $c$	$A_h$
10 $P2/m$			15 $C2/c$	$h_00l_0$ $c$	$A_h$

2nd setting : unique axis // b

## Point group $mm2$ (I)

Incident beam direction	[100]		[010]		[001]		[0vw]		[u0w]	
Space group										
25 $Pmm2$										
26 $Pmc2_1$	$h0l_0$ $c$	$A$			$h0l_0$ $c$	$A$			$h0l_0$ $c$	$A_h$
27 $Pcc2$	$h0l_0$ $c_2$	$A$	$0kl_0$ $c_1$	$A$	$0kl_0$ $c_1$ $h0l_0$ $c_2$	$A$	$0kl_0$ $c_1$	$A_h$	$h0l_0$ $c_2$	$A_h$
28 $Pma2$	$h_00l$ $a$	$A$			$h_00l$ $a$	$A$			$h_00l$ $a$	$A_h$
29 $Pca2_1$	$h_00l$ $a$	$A$	$0kl_0$ $c$	$A$	$0kl_0$ $c$ $h_00l$ $a$	$A$	$0kl_0$ $c$	$A_h$	$h_00l$ $a$	$A_h$
30 $Pnc2$	$h0l_0$ $c$	$A$	$0kl$ $k+l=2n+1$ $n$	$A$	$0kl$ $k+l=2n+1$ $n$ $h0l_0$ $c$	$A$	$0kl$ $k+l=2n+1$ $n$	$A_h$	$h0l_0$ $c$	$A_h$
31 $Pmn2_1$	$h0l$ $h+l=2n+1$ $n$	$A$			$h0l$ $h+l=2n+1$ $n$	$A$			$h0l$ $h+l=2n+1$ $n$	$A_h$
32 $Pba2$	$h_00l$ $a$	$A$	$0k_0l$ $b$	$A$	$0k_0l$ $b$ $h_00l$ $a$	$A$	$0k_0l$ $b$	$A_h$	$h_00l$ $a$	$A_h$
33 $Pna2_1$	$h_00l$ $a$	$A$	$0kl$ $k+l=2n+1$ $n$	$A$	$0kl$ $k+l=2n+1$ $n$ $h_00l$ $a$	$A$	$0kl$ $k+l=2n+1$ $n$	$A_h$	$h_00l$ $a$	$A_h$
34 $Pnn2$	$h0l$ $h+l=2n+1$ $n_2$	$A$	$0kl$ $k+l=2n+1$ $n_1$	$A$	$0kl$ $k+l=2n+1$ $n_1$ $h0l$ $h+l=2n+1$ $n_2$	$A$	$0kl$ $k+l=2n+1$ $n_1$	$A_h$	$h0l$ $h+l=2n+1$ $n_2$	$A_h$

# Determination

## Point group $mm2$ (II)

Incident beam direction	[100]		[010]		[001]		[0vw]		[u0w]	
Space group										
35 $Cmm2$ $ba2$										
36 $Cmc2_1$ $bn2_1$	$h_e0l_o$ $c$	A			$h_e0l_o$ $c$	A			$h_e0l_o$ $c$	$A_h$
37 $Ccc2$ $nn2$	$h_e0l_o$ $c_2$	A	$0k_e l_o$ $c_1$	A	$0k_e l_o$ $c_1$ $h_e0l_o$ $c_2$	A	$0k_e l_o$ $c_1$	$A_h$	$h_e0l_o$ $c_2$	$A_h$
38 $Amm2$ $nc2_1$										
39 $Abm2$ $cc2_1$			$0k_o l_o$ $b$	A	$0k_o l_o$ $b$	A	$0k_o l_o$ $b$	$A_h$		
40 $Ama2$ $nn2_1$	$h_o0l_e$ $a$	A			$h_o0l_e$ $a$	A			$h_o0l_e$ $a$	$A_h$
41 $Aba2$ $cn2_1$	$h_o0l_e$ $a$	A	$0k_o l_o$ $b$	A	$0k_o l_o$ $b$ $h_o0l_e$ $a$	A	$0k_o l_o$ $b$	$A_h$	$h_o0l_e$ $a$	$A_h$
42 $Fmm2$										
43 $Fdd2$ $dd2_1$	$h_e0l_e$ $h_e+l_e=4n+2$ $d_2$	A	$0k_e l_e$ $k_e+l_e=4n+2$ $d_1$	A	$0k_e l_e$ $k_e+l_e=4n+2$ $d_1$ $h_e0l_e$ $h_e+l_e=4n+2$ $d_2$	A	$0k_e l_e$ $k_e+l_e=4n+2$ $d_1$	$A_h$	$h_e0l_e$ $h_e+l_e=4n+2$ $d_2$	$A_h$
44 $Imm2$ $nn2_1$										
45 $Iba2$ $cc2_1$	$h_o0l_o$ $a$	A	$0k_o l_o$ $b$	A	$0k_o l_o$ $b$ $h_o0l_o$ $a$	A	$0k_o l_o$ $b$	$A_h$	$h_o0l_o$ $a$	$A_h$
46 $Ima2$ $nc2_1$	$h_o0l_o$ $a$	A			$h_o0l_o$ $a$	A			$h_o0l_o$ $a$	$A_h$

Note: The meanings of the symbols  $A$ ,  $A_h$  and  $A^*$  are referred to page 52.

**Point group *mmm* (I)**

Incident beam direction	[100]	[010]	[001]	[ <i>uv</i> 0]	[0 <i>vw</i> ]	[ <i>u</i> 0 <i>w</i> ]						
Space group												
47 <i>P</i> 2/ <i>m</i> 2/ <i>m</i> 2/ <i>m</i>												
48 <i>P</i> 2/ <i>n</i> 2/ <i>n</i> 2/ <i>n</i>	$h0l$ $h+l=2n+1$ $n_2$ $hk0$ $h+k=2n+1$ $n_3$	<i>A</i>	$0kl$ $k+l=2n+1$ $n_1$ $hk0$ $h+k=2n+1$ $n_3$	<i>A</i>	$0kl$ $k+l=2n+1$ $n_1$ $h0l$ $h+l=2n+1$ $n_2$	<i>A</i>	$hk0$ $h+k=2n+1$ $n_3$	<i>A<sub>h</sub></i>	$0kl$ $k+l=2n+1$ $n_1$	<i>A<sub>h</sub></i>	$h0l$ $h+l=2n+1$ $n_2$	<i>A<sub>h</sub></i>
49 <i>P</i> 2/ <i>c</i> 2/ <i>c</i> 2/ <i>m</i>	$h0l_o$ $c_2$	<i>A</i>	$0kl_o$ $c_1$	<i>A</i>	$0kl_o$ $c_1$ $h0l_o$ $c_2$	<i>A</i>			$0kl_o$ $c_1$	<i>A<sub>h</sub></i>	$h0l_o$ $c_2$	<i>A<sub>h</sub></i>
50 <i>P</i> 2/ <i>b</i> 2/ <i>a</i> 2/ <i>n</i>	$h_o0l$ $a$ $hk0$ $h+k=2n+1$ $n$	<i>A</i>	$0k_o l$ $b$ $hk0$ $h+k=2n+1$ $n$	<i>A</i>	$0k_o l$ $b$ $h_o0l$ $a$	<i>A</i>	$hk0$ $h+k=2n+1$ $n$	<i>A<sub>h</sub></i>	$0k_o l$ $b$	<i>A<sub>h</sub></i>	$h_o0l$ $a$	<i>A<sub>h</sub></i>
51 <i>P</i> 2 <sub>1</sub> / <i>m</i> 2/ <i>m</i> 2/ <i>a</i>	$h_o k0$ $a$	<i>A</i>	$h_o k0$ $a$	<i>A</i>			$h_o k0$ $a$	<i>A<sub>h</sub></i>				
52 <i>P</i> 2/ <i>n</i> 2 <sub>1</sub> / <i>n</i> 2/ <i>a</i>	$h0l$ $h+l=2n+1$ $n_2$ $h_o k0$ $a$	<i>A</i>	$0kl$ $k+l=2n+1$ $n_1$ $h_o k0$ $a$	<i>A</i>	$0kl$ $k+l=2n+1$ $n_1$ $h0l$ $h+l=2n+1$ $n_2$	<i>A</i>	$h_o k0$ $a$	<i>A<sub>h</sub></i>	$0kl$ $k+l=2n+1$ $n_1$	<i>A<sub>h</sub></i>	$h0l$ $h+l=2n+1$ $n_2$	<i>A<sub>h</sub></i>
53 <i>P</i> 2/ <i>m</i> 2/ <i>n</i> 2 <sub>1</sub> / <i>a</i>	$h0l$ $h+l=2n+1$ $n$ $h_o k0$ $a$	<i>A</i>	$h_o k0$ $a$	<i>A</i>	$h0l$ $h+l=2n+1$ $n$	<i>A</i>	$h_o k0$ $a$	<i>A<sub>h</sub></i>			$h0l$ $h+l=2n+1$ $n$	<i>A<sub>h</sub></i>
54 <i>P</i> 2 <sub>1</sub> / <i>c</i> 2/ <i>c</i> 2/ <i>a</i>	$h0l_o$ $c_2$ $h_o k0$ $a$	<i>A</i>	$0kl_o$ $c_1$ $h_o k0$ $a$	<i>A</i>	$0kl_o$ $c_1$ $h0l_o$ $c_2$	<i>A</i>	$h_o k0$ $a$	<i>A<sub>h</sub></i>	$0kl_o$ $c_1$	<i>A<sub>h</sub></i>	$h0l_o$ $c_2$	<i>A<sub>h</sub></i>
55 <i>P</i> 2 <sub>1</sub> / <i>b</i> 2 <sub>1</sub> / <i>a</i> 2/ <i>m</i>	$h_o0l$ $a$	<i>A</i>	$0k_o l$ $b$	<i>A</i>	$0k_o l$ $b$ $h_o0l$ $a$	<i>A</i>			$0k_o l$ $b$	<i>A<sub>h</sub></i>	$h_o0l$ $a$	<i>A<sub>h</sub></i>
56 <i>P</i> 2 <sub>1</sub> / <i>c</i> 2 <sub>1</sub> / <i>c</i> 2/ <i>n</i>	$h0l_o$ $c_2$ $hk0$ $h+k=2n+1$ $n$	<i>A</i>	$0kl_o$ $c_1$ $hk0$ $h+k=2n+1$ $n$	<i>A</i>	$0kl_o$ $c_1$ $h0l_o$ $c_2$	<i>A</i>	$hk0$ $h+k=2n+1$ $n$	<i>A<sub>h</sub></i>	$0kl_o$ $c_1$	<i>A<sub>h</sub></i>	$h0l_o$ $c_2$	<i>A<sub>h</sub></i>
57 <i>P</i> 2/ <i>b</i> 2 <sub>1</sub> / <i>c</i> 2 <sub>1</sub> / <i>m</i>	$h0l_o$ $c$	<i>A</i>	$0k_o l$ $b$	<i>A</i>	$0k_o l$ $b$ $h0l_o$ $c$	<i>A</i>			$0k_o l$ $b$	<i>A<sub>h</sub></i>	$h0l_o$ $c$	<i>A<sub>h</sub></i>
58 <i>P</i> 2 <sub>1</sub> / <i>n</i> 2 <sub>1</sub> / <i>n</i> 2/ <i>m</i>	$h0l$ $h+l=2n+1$ $n_2$	<i>A</i>	$0kl$ $k+l=2n+1$ $n_1$	<i>A</i>	$0kl$ $k+l=2n+1$ $n_1$ $h0l$ $h+l=2n+1$ $n_2$	<i>A</i>			$0kl$ $k+l=2n+1$ $n_1$	<i>A<sub>h</sub></i>	$h0l$ $h+l=2n+1$ $n_2$	<i>A<sub>h</sub></i>
59 <i>P</i> 2 <sub>1</sub> / <i>m</i> 2 <sub>1</sub> / <i>m</i> 2/ <i>n</i>	$hk0$ $h+k=2n+1$ $n$	<i>A</i>	$hk0$ $h+k=2n+1$ $n$	<i>A</i>			$hk0$ $h+k=2n+1$ $n$	<i>A<sub>h</sub></i>				
60 <i>P</i> 2 <sub>1</sub> / <i>b</i> 2/ <i>c</i> 2 <sub>1</sub> / <i>n</i>	$h0l_o$ $c$ $hk0$ $h+k=2n+1$ $n$	<i>A</i>	$0k_o l$ $b$ $hk0$ $h+k=2n+1$ $n$	<i>A</i>	$0k_o l$ $b$ $h0l_o$ $c$	<i>A</i>	$hk0$ $h+k=2n+1$ $n$	<i>A<sub>h</sub></i>	$0k_o l$ $b$	<i>A<sub>h</sub></i>	$h0l_o$ $c$	<i>A<sub>h</sub></i>

## Point group *mmm* (II)

Incident beam direction	[100]		[010]		[001]		[uv0]		[0vw]		[u0w]	
	Space group											
61 $P2_1/b2_1/c2_1/a$	$h0l_o$ $c$ $h_o k_0$ $a$	A	$0k_o l$ $b$ $h_o k_0$ $a$	A	$0k_o l$ $b$ $h0l_o$ $c$	A	$h_o k_0$ $a$	$A_h$	$0k_o l$ $b$	$A_h$	$h0l_o$ $c$	$A_h$
62 $P2_1/n2_1/m2_1/a$	$h_o k_0$ $a$	A	$0kl$ $k+l=2n+1$ $n$ $h_o k_0$ $a$	A	$0kl$ $k+l=2n+1$ $n$	A	$h_o k_0$ $a$	$A_h$	$0kl$ $k+l=2n+1$ $n$	$A_h$		
63 $C2/m2/c2_1/m$	$h_e 0l_o$ $c$	A			$h_e 0l_o$ $c$	A					$h_e 0l_o$ $c$	$A_h$
64 $C2/m2/c2_1/a$	$h_e 0l_o$ $c$ $h_o k_o 0$ $a$	A	$h_o k_o 0$ $a$	A	$h_e 0l_o$ $c$	A	$h_o k_o 0$ $a$	$A_h$			$h_e 0l_o$ $c$	$A_h$
65 $C2/m2/m2/m$												
66 $C2/c2/c2/m$	$h_e 0l_o$ $c_2$	A	$0k_e l_o$ $c_1$	A	$0k_e l_o$ $c_1$ $h_e 0l_o$ $c_2$	A			$0k_e l_o$ $c_1$	$A_h$	$h_e 0l_o$ $c_2$	$A_h$
67 $C2/m2/m2/a$	$h_o k_o 0$ $a$	A	$h_o k_o 0$ $a$	A			$h_o k_o 0$ $a$	$A_h$				
68 $C2/c2/c2/a$	$h_e 0l_o$ $c_2$ $h_o k_o 0$ $a$	A	$0k_e l_o$ $c_1$ $h_o k_o 0$ $a$	A	$0k_e l_o$ $c_1$ $h_e 0l_o$ $c_2$	A	$h_o k_o 0$ $a$	$A_h$	$0k_e l_o$ $c_1$	$A_h$	$h_e 0l_o$ $c_2$	$A_h$
69 $F2/m2/m2/m$												
70 $F2/d2/d2/d$	$h_e 0l_e$ $h_e+l_e=4n+2$ $d_2$ $h_e k_e 0$ $h_e+k_e=4n+2$ $d_3$	A	$h_e k_e 0$ $h_e+k_e=4n+2$ $d_3$ $0k_e l_e$ $k_e+l_e=4n+2$ $d_1$	A	$0k_e l_e$ $k_e+l_e=4n+2$ $d_1$ $h_e 0l_e$ $h_e+l_e=4n+2$ $d_2$	A	$h_e k_e 0$ $h_e+k_e=4n+2$ $d_3$	$A_h$	$0k_e l_e$ $k_e+l_e=4n+2$ $d_1$	$A_h$	$h_e 0l_e$ $h_e+l_e=4n+2$ $d_2$	$A_h$
71 $I2/m2/m2/m$												
72 $I2/b2/a2/m$	$h_o 0l_o$ $a$	A	$0k_o l_o$ $b$	A	$0k_o l_o$ $b$ $h_o 0l_o$ $a$	A			$0k_o l_o$ $b$	$A_h$	$h_o 0l_o$ $a$	$A_h$
73 $I2/b2/c2/a$	$h_o 0l_o$ $c$ $h_o k_o 0$ $a$	A	$h_o k_o 0$ $a$ $0k_o l_o$ $b$	A	$0k_o l_o$ $b$ $h_o 0l_o$ $c$	A	$h_o k_o 0$ $a$	$A_h$	$0k_o l_o$ $b$	$A_h$	$h_o 0l_o$ $c$	$A_h$
74 $I2/m2/m2/a$	$h_o k_o 0$ $a$	A	$h_o k_o 0$ $a$	A			$h_o k_o 0$ $a$	$A_h$				

### Point group 4/m

Incident beam direction	[100]		[uv0]	
	[110]			
Space group				
83 $P4/m$				
84 $P4_2/m$				
85 $P4/n$	$hk0$ $h+k=2n+1$ $n$	A	$hk0$ $h+k=2n+1$ $n$	$A_h$

Incident beam direction	[100]		[uv0]	
	[110]			
Space group				
86 $P4_2/n$	$hk0$ $h+k=2n+1$ $n$	A	$hk0$ $h+k=2n+1$ $n$	$A_h$
87 $I4/m$				
88 $I4_1/a$	$h_0k_00$ $a$	A	$h_0k_00$ $a$	$A_h$

### Point group 4mm(I)

Incident beam direction	[100]		[001]		[110]		[u0w]*		[uvw]	
Space group										
99 $P4mm$										
100 $P4bm$	$h_00l$ $a_2$	A	$0k_0l$ $b_1$ $h_00l$ $a_2$	A			$h_00l$ $a$	$A_h$		
101 $P4_2cm$	$h0l_0$ $c_2$	A	$0kl_0$ $c_1$ $h0l_0$ $c_2$	A			$h0l_0$ $c$	$A_h$		
102 $P4_2nm$	$h0l$ $h+l=2n+1$ $n_2$	A	$0kl$ $k+l=2n+1$ $n_1$ $h0l$ $h+l=2n+1$ $n_2$	A			$h0l$ $h+l=2n+1$ $n$	$A_h$		
103 $P4cc$	$h0l_0$ $c_{12}$	A	$0kl_0$ $c_{11}$ $h0l_0$ $c_{12}$ $hhl_0$ $hhl_0$ $c_2$	A	$hhl_0$ $c_2$	A	$h0l_0$ $c_1$	$A_h$	$hhl_0$ $c_2$	$A_h$
104 $P4nc$	$h0l$ $h+l=2n+1$ $n_2$	A	$0kl$ $k+l=2n+1$ $n_1$ $h0l$ $h+l=2n+1$ $n_2$ $hhl_0$ $hhl_0$ $c$	A	$hhl_0$ $c$	A	$h0l$ $h+l=2n+1$ $n$	$A_h$	$hhl_0$ $c$	$A_h$
105 $P4_2mc$			$hhl_0$ $hhl_0$ $c$	A	$hhl_0$ $c$	A			$hhl_0$ $c$	$A_h$
106 $P4_2bc$	$h_00l$ $a_2$	A	$0k_0l$ $b_1$ $h_00l$ $a_2$ $hhl_0$ $hhl_0$ $c$	A	$hhl_0$ $c$	A	$h_00l$ $a$	$A_h$	$hhl_0$ $c$	$A_h$
107 $I4mm$										
108 $I4cm$	$h_00l_0$ $c_2$	A	$0k_0l_0$ $c_1$ $h_00l_0$ $c_2$	A			$h_00l_0$ $c$	$A_h$		

\*The symbol "a" in the column of [u0w] incidence is equivalent to the symbol "b" in the space groups of the first column.

### Point group 4mm(II)

Incident beam direction	[100]		[001]		[110]		[u0w]		[uuw]	
Space group										
109 $I4_1md$			$hhl_e$ $\bar{h}hl_e$ $2h+l_e=4n+2$ $d$	A	$hhl_e$ $2h+l_e=4n+2$ $d$	A			$hhl_e$ $2h+l_e=4n+2$ $d$	$A_h$
110 $I4_1cd$	$h_00l_0$ $c_2$	A	$0k_0l_0$ $c_1$ $h_00l_0$ $c_2$ $hhl_e$ $\bar{h}hl_e$ $2h+l_e=4n+2$ $d$	A	$hhl_e$ $2h+l_e=4n+2$ $d$	A	$h_00l_0$ $c$	$A_h$	$hhl_e$ $2h+l_e=4n+2$ $d$	$A_h$

### Point group $\bar{4}2m$

Incident beam direction	[100]		[001]		[110]		[u0w]*		[uuw]	
Space group										
111 $P\bar{4}2m$										
112 $P\bar{4}2c$			$hhl_0$ $\bar{h}hl_0$ $c$	A	$hhl_0$ $c$	A			$hhl_0$ $c$	$A_h$
113 $P\bar{4}2_1m$										
114 $P\bar{4}2_1c$			$hhl_0$ $\bar{h}hl_0$ $c$	A	$hhl_0$ $c$	A			$hhl_0$ $c$	$A_h$
115 $P\bar{4}m2$										
116 $P\bar{4}c2$	$h0l_0$ $c_2$	A	$0kl_0$ $c_1$ $h0l_0$ $c_2$	A			$h0l_0$ $c$	$A_h$		
117 $P\bar{4}b2$	$h_00l$ $a_2$	A	$0k_0l$ $b_1$ $h_00l$ $a_2$	A			$h_00l$ $a$	$A_h$		
118 $P\bar{4}n2$	$h0l$ $h+l=2n+1$ $n_2$	A	$0kl$ $k+l=2n+1$ $n_1$ $h0l$ $h+l=2n+1$ $n_2$	A			$h0l$ $h+l=2n+1$ $n$	$A_h$		
119 $I\bar{4}m2$										
120 $I\bar{4}c2$	$h_00l_0$ $c_2$	A	$0k_0l_0$ $c_1$ $h_00l_0$ $c_2$	A			$h_00l_0$ $c$	$A_h$		
121 $I\bar{4}2m$										
122 $I\bar{4}2d$			$hhl_e$ $\bar{h}hl_e$ $2h+l_e=4n+2$ $d$	A	$hhl_e$ $2h+l_e=4n+2$ $d$	A			$hhl_e$ $2h+l_e=4n+2$ $d$	$A_h$

\* The symbol "a" in the column of [u0w] incidence is equivalent to the symbol "b" in the space groups of the first column.

### Point group 4/mmm(I)

Incident beam direction	[100]		[001]		[110]		[u0w]*		[uuv]		[uv0]	
Space group												
123 $P4/mmm$ $P4/m2/m2/m$												
124 $P4/mcc$ $P4/m2/c2/c$	$h0l_0$ $c_{12}$	A	$0kl_0$ $c_{11}$ $h0l_0$ $c_{12}$ $\bar{h}hl_0$ $\bar{h}hl_0$ $c_2$	A	$hhl_0$ $c_2$	A	$h0l_0$ $c_1$	$A_h$	$hhl_0$ $c_2$	$A_h$		
125 $P4/nbm$ $P4/n2/b2/m$	$hk0$ $h+k=2n+1$ $n$ $h_00l$ $a_2$	A	$0k_0l$ $b_1$ $h_00l$ $a_2$	A	$hk0$ $h+k=2n+1$ $n$	A	$h_00l$ $a$	$A_h$			$hk0$ $h+k=2n+1$ $n$	$A_h$
126 $P4/nnc$ $P4/n2/n2/c$	$hk0$ $h+k=2n+1$ $n_1$ $h0l$ $h+l=2n+1$ $n_{22}$	A	$0kl$ $k+l=2n+1$ $n_{21}$ $h0l$ $h+l=2n+1$ $n_{22}$ $\bar{h}hl_0$ $\bar{h}hl_0$ $c$	A	$hk0$ $h+k=2n+1$ $n_1$ $hhl_0$ $c$	A	$h0l$ $h+l=2n+1$ $n_2$	$A_h$	$hhl_0$ $c$	$A_h$	$hk0$ $h+k=2n+1$ $n_1$	$A_h$
127 $P4/mbm$ $P4/m2_1/b2/m$	$h_00l$ $a_2$	A	$0k_0l$ $b_1$ $h_00l$ $a_2$	A			$h_00l$ $a$	$A_h$				
128 $P4/mnc$ $P4/m2_1/n2/c$	$h0l$ $h+l=2n+1$ $n_2$	A	$0kl$ $k+l=2n+1$ $n_1$ $h0l$ $h+l=2n+1$ $n_2$ $\bar{h}hl_0$ $\bar{h}hl_0$ $c$	A	$hhl_0$ $c$	A	$h0l$ $h+l=2n+1$ $n$	$A_h$	$hhl_0$ $c$	$A_h$		
129 $P4/nmm$ $P4/n2_1/m2/m$	$hk0$ $h+k=2n+1$ $n$	A			$hk0$ $h+k=2n+1$ $n$	A					$hk0$ $h+k=2n+1$ $n$	$A_h$
130 $P4/ncc$ $P4/n2_1/c2/c$	$hk0$ $h+k=2n+1$ $n$ $h0l_0$ $c_{12}$	A	$0kl_0$ $c_{11}$ $h0l_0$ $c_{12}$ $\bar{h}hl_0$ $\bar{h}hl_0$ $c_2$	A	$hk0$ $h+k=2n+1$ $n$ $hhl_0$ $c_2$	A	$h0l_0$ $c_1$	$A_h$	$hhl_0$ $c_2$	$A_h$	$hk0$ $h+k=2n+1$ $n$	$A_h$
131 $P4_2/mmc$ $P4_2/m2/m2/c$			$hhl_0$ $\bar{h}hl_0$ $c$	A	$hhl_0$ $c$	A			$hhl_0$ $c$	$A_h$		
132 $P4_2/mcm$ $P4_2/m2/c2/m$	$h0l_0$ $c_2$	A	$0kl_0$ $c_1$ $h0l_0$ $c_2$	A			$h0l_0$ $c$	$A_h$				

\*The symbol "a" in the column of [u0w] incidence is equivalent to the symbol "b" in the space groups of the first column.

### Point group 4/mmm(II)

Incident beam direction	[100]		[001]		[110]		[u0w]*		[uuw]		[uw0]	
Space group												
133 $P4_2/nbc$ $P4_2/n2/b2/c$	$hk0$ $h+k=2n+1$ $n$ $h_0l$ $a_2$	A	$0k_0l$ $b_1$ $h_0l$ $a_2$ $hhl_0$ $\bar{h}hl_0$ $c$	A	$hk0$ $h+k=2n+1$ $n$ $hhl_0$ $c$	A	$h_0l$ $a$	$A_h$	$hhl_0$ $c$	$A_h$	$hk0$ $h+k=2n+1$ $n$	$A_h$
134 $P4_2/nmm$ $P4_2/n2/n2/m$	$hk0$ $h+k=2n+1$ $n_1$ $h0l$ $h+l=2n+1$ $n_{22}$	A	$0kl$ $k+l=2n+1$ $n_{21}$ $h0l$ $h+l=2n+1$ $n_{22}$	A	$hk0$ $h+k=2n+1$ $n_1$	A	$h0l$ $h+l=2n+1$ $n_2$	$A_h$			$hk0$ $h+k=2n+1$ $n_1$	$A_h$
135 $P4_2/mbc$ $P4_2/m2_1/b2/c$	$h_0l$ $a_2$	A	$0k_0l$ $b_1$ $h_0l$ $a_2$ $hhl_0$ $\bar{h}hl_0$ $c$	A	$hhl_0$ $c$	A	$h_0l$ $a$	$A_h$	$hhl_0$ $c$	$A_h$		
136 $P4_2/mnm$ $P4_2/m2_1/n2/m$	$h0l$ $h+l=2n+1$ $n_2$	A	$0kl$ $k+l=2n+1$ $n_1$ $h0l$ $h+l=2n+1$ $n_2$	A			$h0l$ $h+l=2n+1$ $n$	$A_h$				
137 $P4_2/nmc$ $P4_2/n2_1/m2/c$	$hk0$ $h+k=2n+1$ $n$	A	$hhl_0$ $\bar{h}hl_0$ $c$	A	$hhl_0$ $c$ $hk0$ $h+k=2n+1$ $n$	A			$hhl_0$ $c$	$A_h$	$hk0$ $h+k=2n+1$ $n$	$A_h$
138 $P4_2/ncm$ $P4_2/n2_1/c2/m$	$hk0$ $h+k=2n+1$ $n$ $h0l_0$ $c_2$	A	$0kl_0$ $c_1$ $h_0l_0$ $c_2$	A	$hk0$ $h+k=2n+1$ $n$	A	$h0l_0$ $c$	$A_h$			$hk0$ $h+k=2n+1$ $n$	$A_h$
139 $I4/mmm$ $I4/m2/m2/m$												
140 $I4/mcm$ $I4/m2/c2/m$	$h_0l_0$ $c_2$	A	$0k_0l_0$ $c_1$ $h_0l_0$ $c_2$	A			$h_0l_0$ $c$	$A_h$				
141 $I4_1/amd$ $I4_1/a2/m2/d$	$h_0k_00$ $a$	A	$hhl_e$ $\bar{h}hl_e$ $2h+l_e=4n+2$ $d$	A	$h_0k_00$ $a$ $hhl_e$ $2h+l_e=4n+2$ $d$	A			$hhl_e$ $2h+l_e=4n+2$ $d$	$A_h$	$h_0k_00$ $a$	$A_h$
142 $I4_1/acd$ $I4_1/a2/c2/d$	$h_0k_00$ $a$ $h_0l_0$ $c_2$	A	$0k_0l_0$ $c_1$ $h_0l_0$ $c_2$ $hhl_e$ $\bar{h}hl_e$ $2h+l_e=4n+2$ $d$	A	$h_0k_00$ $a$ $hhl_e$ $2h+l_e=4n+2$ $d$	A	$h_0l_0$ $c$	$A_h$	$hhl_e$ $2h+l_e=4n+2$ $d$	$A_h$	$h_0k_00$ $a$	$A_h$

\*The symbol "a" in the column of [u0w] incidence is equivalent to the symbol "b" in the space groups of the first column.

## Point groups $3m, \bar{3}m$

Incident beam direction	[0001]		[11 $\bar{2}$ 0]		[1 $\bar{1}$ 00]		[11 $\bar{2}$ $\omega$ ]		[1 $\bar{1}$ 0 $\omega$ ]	
Space group										
156 $P3m1$										
157 $P31m$										
158 $P3c1$	$h\bar{h}0l_0$ $0h\bar{h}l_0$ $\bar{h}0hl_0$ $c$	$A$			$h\bar{h}0l_0$ $c$	$A$			$h\bar{h}0l_0$ $c$	$A_h$
159 $P31c$	$hh2\bar{h}l_0$ $h2\bar{h}hl_0$ $2\bar{h}hhl_0$ $c$	$A$	$hh2\bar{h}l_0$ $c$	$A$			$hh2\bar{h}l_0$ $c$	$A_h$		
160 $R3m$										
161 $R3c$	$h\bar{h}0l_0$ $0h\bar{h}l_0$ $\bar{h}0hl_0$ $h+l_0=3n$ $c$	$A_h$			$h\bar{h}0l_0$ $h+l_0=3n$ $c$	$A_h$			$h\bar{h}0l_0$ $h+l_0=3n$ $c$	$A_h$
162 $P\bar{3}1m$										
163 $P\bar{3}1c$	$hh2\bar{h}l_0$ $h2\bar{h}hl_0$ $2\bar{h}hhl_0$ $c$	$A$	$hh2\bar{h}l_0$ $c$	$A$			$hh2\bar{h}l_0$ $c$	$A_h$		
164 $P\bar{3}m1$										
165 $P\bar{3}c1$	$h\bar{h}0l_0$ $0h\bar{h}l_0$ $\bar{h}0hl_0$ $c$	$A$			$h\bar{h}0l_0$ $c$	$A$			$h\bar{h}0l_0$ $c$	$A_h$
166 $R\bar{3}m$										
167 $R\bar{3}c$	$h\bar{h}0l_0$ $0h\bar{h}l_0$ $\bar{h}0hl_0$ $h+l_0=3n$ $c$	$A_h$			$h\bar{h}0l_0$ $h+l_0=3n$ $c$	$A_h$			$h\bar{h}0l_0$ $h+l_0=3n$ $c$	$A_h$

**Point groups  $6mm, \bar{6}m2, 6/mmm$**

Incident beam direction	[0001]		[11 $\bar{2}$ 0]		[1 $\bar{1}$ 00]		[11 $\bar{2}$ w]		[1 $\bar{1}$ 0w]	
Space group										
183 $P6mm$										
184 $P6cc$	$\begin{matrix} h\bar{h}0l_0 \\ 0h\bar{h}l_0 \\ \bar{h}0hl_0 \\ c_1 \\ hh2\bar{h}l_0 \\ h2\bar{h}hl_0 \\ 2h\bar{h}hl_0 \\ c_2 \end{matrix}$	A	$\begin{matrix} hh2\bar{h}l_0 \\ c_2 \end{matrix}$	A	$\begin{matrix} h\bar{h}0l_0 \\ c_1 \end{matrix}$	A	$\begin{matrix} hh2\bar{h}l_0 \\ c_2 \end{matrix}$	$A_h$	$\begin{matrix} h\bar{h}0l_0 \\ c_1 \end{matrix}$	$A_h$
185 $P6_3cm$	$\begin{matrix} h\bar{h}0l_0 \\ 0h\bar{h}l_0 \\ \bar{h}0hl_0 \\ c \end{matrix}$	A			$\begin{matrix} h\bar{h}0l_0 \\ c \end{matrix}$	A			$\begin{matrix} h\bar{h}0l_0 \\ c \end{matrix}$	$A_h$
186 $P6_3mc$	$\begin{matrix} hh2\bar{h}l_0 \\ h2\bar{h}hl_0 \\ 2h\bar{h}hl_0 \\ c \end{matrix}$	A	$\begin{matrix} hh2\bar{h}l_0 \\ c \end{matrix}$	A			$\begin{matrix} hh2\bar{h}l_0 \\ c \end{matrix}$	$A_h$		
187 $P\bar{6}m2$										
188 $P\bar{6}c2$	$\begin{matrix} h\bar{h}0l_0 \\ 0h\bar{h}l_0 \\ \bar{h}0hl_0 \\ c \end{matrix}$	A			$\begin{matrix} h\bar{h}0l_0 \\ c \end{matrix}$	A			$\begin{matrix} h\bar{h}0l_0 \\ c \end{matrix}$	$A_h$
189 $P\bar{6}2m$										
190 $P\bar{6}2c$	$\begin{matrix} hh2\bar{h}l_0 \\ h2\bar{h}hl_0 \\ 2h\bar{h}hl_0 \\ c \end{matrix}$	A	$\begin{matrix} hh2\bar{h}l_0 \\ c \end{matrix}$	A			$\begin{matrix} hh2\bar{h}l_0 \\ c \end{matrix}$	$A_h$		
191 $P6/mmm$										
192 $P6/mcc$	$\begin{matrix} h\bar{h}0l_0 \\ 0h\bar{h}l_0 \\ \bar{h}0hl_0 \\ c_1 \\ hh2\bar{h}l_0 \\ h2\bar{h}hl_0 \\ 2h\bar{h}hl_0 \\ c_2 \end{matrix}$	A	$\begin{matrix} hh2\bar{h}l_0 \\ c_2 \end{matrix}$	A	$\begin{matrix} h\bar{h}0l_0 \\ c_1 \end{matrix}$	A	$\begin{matrix} hh2\bar{h}l_0 \\ c_2 \end{matrix}$	$A_h$	$\begin{matrix} h\bar{h}0l_0 \\ c_1 \end{matrix}$	$A_h$
193 $P6_3/mcm$	$\begin{matrix} h\bar{h}0l_0 \\ 0h\bar{h}l_0 \\ \bar{h}0hl_0 \\ c \end{matrix}$	A			$\begin{matrix} h\bar{h}0l_0 \\ c \end{matrix}$	A			$\begin{matrix} h\bar{h}0l_0 \\ c \end{matrix}$	$A_h$
194 $P6_3/mmc$	$\begin{matrix} hh2\bar{h}l_0 \\ h2\bar{h}hl_0 \\ 2h\bar{h}hl_0 \\ c \end{matrix}$	A	$\begin{matrix} hh2\bar{h}l_0 \\ c \end{matrix}$	A			$\begin{matrix} hh2\bar{h}l_0 \\ c \end{matrix}$	$A_h$		

## Point group $m\bar{3}$

Incident beam direction	[100]		[110]		[uv0]	
Space group						
200 $Pm\bar{3}$ $P2/m\bar{3}$						
201 $Pn\bar{3}$ $P2/n\bar{3}$	$h0l$ $h+l=2n+1$ $n_2$ $hk0$ $h+k=2n+1$ $n_3$	A	$hk0$ $h+k=2n+1$ $n_3$	A	$hk0$ $h+k=2n+1$ $n$	$A_h$
202 $Fm\bar{3}$ $F2/m\bar{3}$						
203 $Fd\bar{3}$ $F2/d\bar{3}$	$h_e0l_e$ $h_e+l_e=4n+2$ $d_2$ $h_e k_e0$ $h_e+k_e=4n+2$ $d_3$	A	$h_e k_e0$ $h_e+k_e=4n+2$ $d_3$	A	$h_e k_e0$ $h_e+k_e=4n+2$ $d$	$A_h$
204 $Im\bar{3}$ $I2/m\bar{3}$						
205 $Pa\bar{3}$ $P2_1/a\bar{3}$	$h0l_o$ $c_2$ $h_o k_o0$ $a_3$	A	$h_o k_o0$ $a_3$	$A^*$	$h_o k_o0$ $a$	$A_h$
206 $Ia\bar{3}$ $I2_1/a\bar{3}$	$h_o0l_o$ $c_2$ $h_o k_o0$ $a_3$	A	$h_o k_o0$ $a_3$	A	$h_o k_o0$ $a$	$A_h$

## Point group $\bar{4}3m$

Incident beam direction	[100]*		[110]		[uvw]	
Space group						
215 $P\bar{4}3m$						
216 $F\bar{4}3m$						
217 $I\bar{4}3m$						
218 $P\bar{4}3n$	$h_o k k, h_o \bar{k} k$ $n$	A	$h h l_o$ $n$	A	$h h l_o$ $n$	$A_h$
219 $F\bar{4}3c$	$h_o k_o k_o, h_o \bar{k}_o k_o$ $a$	A	$h_o h_o l_o$ $c$	A	$h_o h_o l_o$ $c$	$A_h$
220 $I\bar{4}3d$	$h_e k k$ $h_e \bar{k} k$ $2k+h_e=4n+2$ $d$	A	$h h l_e$ $2h+l_e=4n+2$ $d$	A	$h h l_e$ $2h+l_e=4n+2$ $d$	$A_h$

\*The symbol "a" in the column of [100] incidence is equivalent to the symbol "c" in the space groups of the first column.

### Point group $m\bar{3}m$

Incident beam direction	[100]*		[110]		[uv0]		[uvw]	
Space group								
221 $Pm\bar{3}m$ $P4/m\bar{3}2/m$								
222 $Pn\bar{3}n$ $P4/n\bar{3}2/n$	$h0l$ $h+l=2n+1$ $n_{12}$ $hk0$ $h+k=2n+1$ $n_{13}$ $h_0kk, h_0\bar{k}k$ $n_2$	A	$hk0$ $h+k=2n+1$ $n_{13}$ $hhl_0$ $n_2$	A	$hk0$ $h+k=2n+1$ $n_1$	$A_h$	$hhl_0$ $n_2$	$A_h$
223 $Pm\bar{3}n$ $P4_2/m\bar{3}2/n$	$h_0kk, h_0\bar{k}k$ $n$	A	$hhl_0$ $n$	A			$hhl_0$ $n$	$A_h$
224 $Pn\bar{3}m$ $P4_2/n\bar{3}2/m$	$h0l$ $h+l=2n+1$ $n_2$ $hk0$ $h+k=2n+1$ $n_3$	A	$hk0$ $h+k=2n+1$ $n_3$	A	$hk0$ $h+k=2n+1$ $n$	$A_h$		
225 $Fm\bar{3}m$ $F4/m\bar{3}2/m$								
226 $Fm\bar{3}c$ $F4/m\bar{3}2/c$	$h_0k_0k_0, h_0\bar{k}_0k_0$ $a$	A	$h_0h_0l_0$ $c$	A			$h_0h_0l_0$ $c$	$A_h$
227 $Fd\bar{3}m$ $F4_1/d\bar{3}2/m$	$h_e0l_e$ $h_e+l_e=4n+2$ $d_2$ $h_ek_e0$ $h_e+k_e=4n+2$ $d_3$	A	$h_ek_e0$ $h_e+k_e=4n+2$ $d_3$	A	$h_ek_e0$ $h_e+k_e=4n+2$ $d$	$A_h$		
228 $Fd\bar{3}c$ $F4_1/d\bar{3}2/c$	$h_e0l_e$ $h_e+l_e=4n+2$ $d_2$ $h_ek_e0$ $h_e+k_e=4n+2$ $d_3$ $h_0k_0k_0, h_0\bar{k}_0k_0$ $a$	A	$h_0h_0l_0$ $c$ $h_ek_e0$ $h_e+k_e=4n+2$ $d_3$	A	$h_ek_e0$ $h_e+k_e=4n+2$ $d$	$A_h$	$h_0h_0l_0$ $c$	$A_h$
229 $Im\bar{3}m$ $I4/m\bar{3}2/m$								
230 $Ia\bar{3}d$ $I4_1/a\bar{3}2/d$	$h_0k_00$ $a_3$ $h_00l_0$ $c_2$ $h_ek_k, h_e\bar{k}k$ $2k+h_e=4n+2$ $d$	A	$hhl_e$ $2h+l_e=4n+2$ $d$ $h_0k_00$ $a_3$	A	$h_0k_00$ $a$	$A_h$	$hhl_e$ $2h+l_e=4n+2$ $d$	$A_h$

\*The symbol "a" in the column of [100] incidence is equivalent to the symbol "c" in the space groups of the first column.

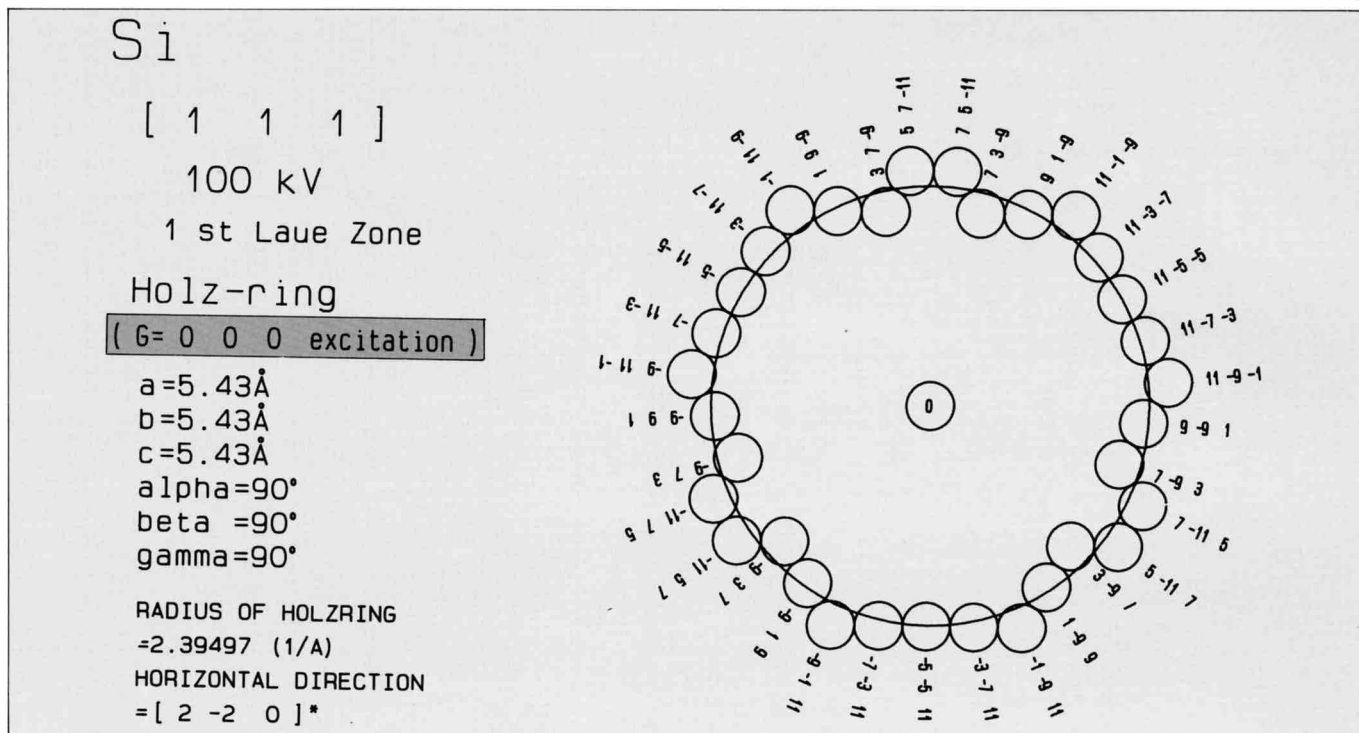
# Computer Simulations

## HOLZ line program

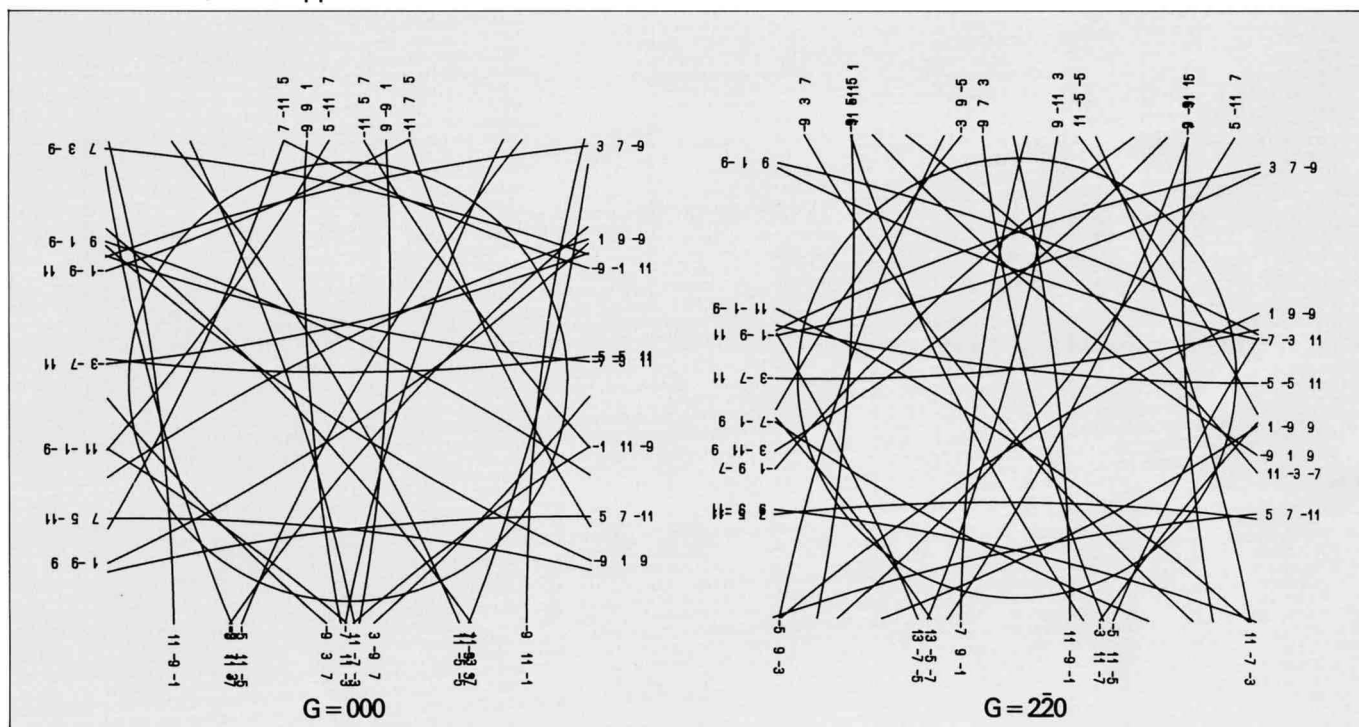
This program can simulate a HOLZ ring and HOLZ lines appearing in the bright-field and dark-field disks in the kinematical approximation for all the crystal systems and all the zone axes. HOLZ lines are drawn 1) by using arcs (HOLZ I) and 2) by solving Bragg equation (HOLZ

II). The number of HOLZ lines in the dark-field disk G drawn by HOLZ II is twice that by HOLZ I, because the HOLZ lines excited not only from the bright-field but also from the dark-field G are drawn when using HOLZ II.

HOLZ ring



HOLZ lines: arc (circle) approximation



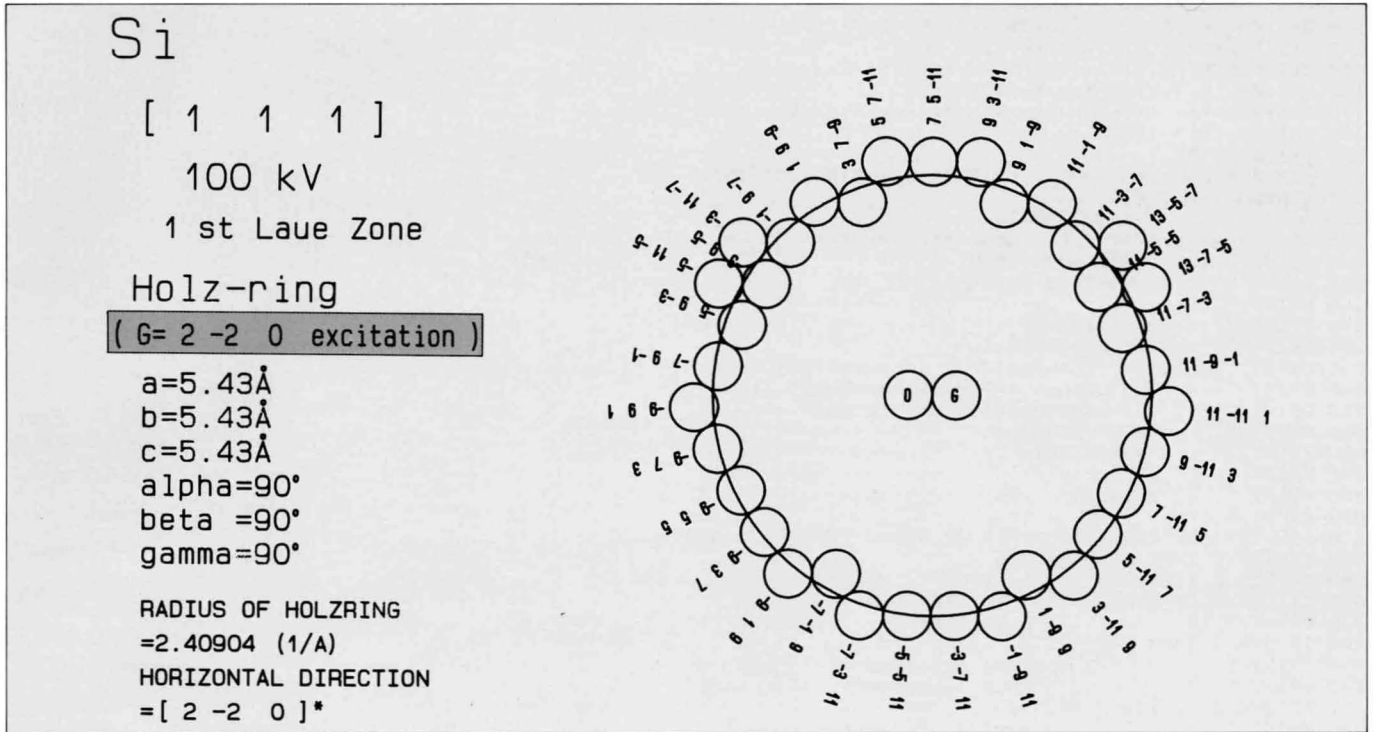
HOLZI is used in determining reflection indices and the senses of excitation errors which are necessary in the identification of lattice defects, but has a low accuracy in reproducing the positions of reflection lines.

HOLZII is recommended for use in the determination of

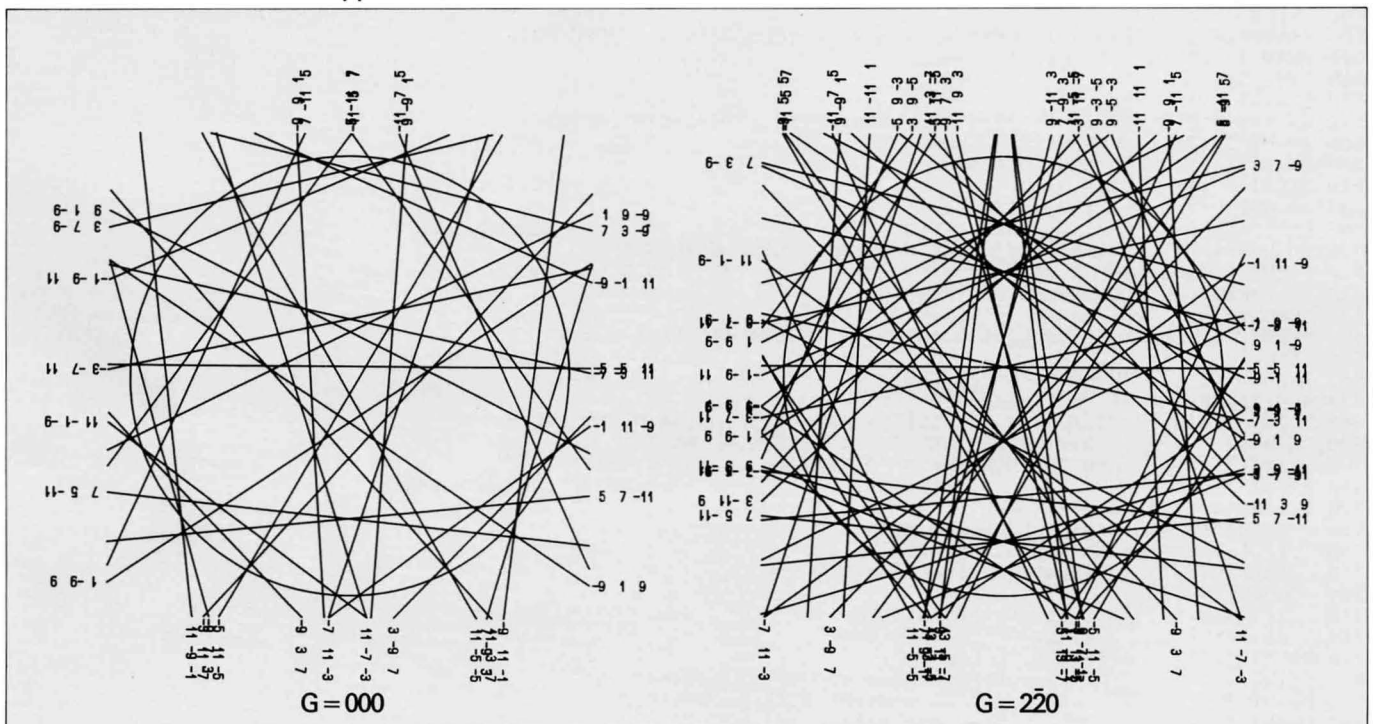
the accelerating voltage and lattice parameters, but is not suitable for finding the signs of excitation errors.

Simulated patterns are printed out to a printer or a plotter. Subprograms of CHPR and CHPL are for printing out simulation patterns to a printer and a plotter, respectively.

HOLZ ring



HOLZ lines: more accurate approximation



```

10 ' *****
20 ' ***** H O L Z *****
30 ' *****
40 CONSOLE 0,25,0,0
50 REM ***** definition of user function *****
60 DEF FNPARITY(X)=2*(X/2-INT(X/2))
70 DEF FNPRO(X1,X2,X3,Y1,Y2,Y3)=X1*Y1+X2*Y2+X3*Y3
80 DEF FNCS(X1,Y1,Z1,X2,Y2,Z2)=(X1*X2+Y1*Y2+Z1*Z2)/SQR((X1*X1+Y1*Y1+Z1*Z1)*(X2*X2+Y2*Y2+Z2*Z2))
90 DEF FNRL(H,K,L)=SQR((H*AST1)^2+(H*AST2+K*BST2+L*CST2)^2+(H*AST3+L*CST3)^2)
100 DEF FNXABC(H,K,L)=H*AST1+K*BST1+L*CST1
110 DEF FNYABC(H,K,L)=H*AST2+K*BST2+L*CST2
120 DEF FNZABC(H,K,L)=H*AST3+K*BST3+L*CST3
130 DEF FNPROX(X,Y,Z)=(UU*WW*X+VV*WW*Y-FA1*FA1*Z)/(FA1*FA2)
140 DEF FNPROY(X,Y,Z)=(VV*X-UU*Y)/FA1
150 DEF FNPROZ(X,Y,Z)=-(UU*X+VV*Y+WW*Z)/FA2
160 DEF FNL(X,Y,Z)=X*X+Y*Y+Z*Z
170 ' *****
180 PAI#=3.14159265359#
190 OPTION BASE 1
200 DIM HCA(300),KCA(300),LCA(300),DISK(300),SO(25)
210 SCREEN 2,0:CLS 3
220 '
230 REM ***** data input *****
240 INPUT " (1) SPECIMEN NAME " ;S$
250 PRINT " (2) CRYSTAL SYSTEM"
260 PRINT " cubic ----- 1"
270 PRINT " tetragonal ----- 2"
280 PRINT " rhombohedral"
290 PRINT " (rhombohedral coordinates) --- 3"
300 PRINT " hexagonal, trigonal, rhombohedral"
310 PRINT " (hexagonal coordinates) ----- 4"
320 PRINT " orthorhombic ----- 5"
330 PRINT " monoclinic ----- 6"
340 PRINT " triclinic ----- 7"
350 PRINT " diamond type ----- 8"
360 INPUT " " ;SYS
370 SYS=INT(ABS(SYS)):IF SYS>8 OR SYS=0 THEN GOTO 360
380 IF SYS=6 THEN GOSUB *SYS6
390 IF SYS=8 THEN 530
400 IF SYS=3 OR SYS=4 OR SYS=7 THEN 510
410 PRINT " (4) primitive ----- 1"
420 IF SYS=2 THEN 440
430 PRINT " face centered ----- 2"
440 PRINT " body centered ----- 3"
450 IF SYS=1 OR SYS=2 THEN 490
460 PRINT " A-base centered ----- 4"
470 PRINT " B-base centered ----- 5"
480 PRINT " C-base centered ----- 6"
490 INPUT " " ;BRAV
500 BRAV=FIX(ABS(BRAV)):IF BRAV>6 OR BRAV=0 THEN GOTO 490 ELSE GOTO 540
510 BRAV=1 ' primitive
520 GOTO 540
530 BRAV=7
540 ON SYS GOSUB *SYS1,*SYS2,*SYS3,*SYS4,*SYS5,*SYS6,*SYS7,*SYS1
550 INPUT " (7) ACCELERATING VOLTAGE E(kV) =" ;E
560 E=ABS(E):IF E=0 THEN GOTO 550
570 INPUT " (8) ZONE AXIS U,V,W =" ;U,V,W
580 IF U*U+V*V+W*W=0 THEN GOTO 570
590 INPUT " (9) EXCITE G-REFLECTION ? (y/n) " ;GREF$
600 IF GREF$="n" OR GREF$="N" THEN HG=0:KG=0:LG=0:GOTO 660
610 INPUT " (10) INDEX OF G H,K,L =" ;HG,KG,LG
620 IF FNPRO(U,V,W,HG,KG,LG)=0 THEN 660
630 BEEP
640 PRINT " reinput indices of G which is in the 0th Laue zone!"
650 INPUT " H,K,L =" ;HG,KG,LG:GOTO 620
660 INPUT " (11) ORDER OF LAUE ZONE N=" ;N
670 N=FIX(ABS(N)):IF N=0 THEN GOTO 660
680 PRINT " (12) INDEX OF A REFLECTION ADJACENT TO THE DIRECT BEAM "
690 PRINT " (THIS DETERMINES THE DIAMETER OF DISKS"
700 PRINT " AND THE HORIZONTAL DIRECTION IN THE OUTPUT)"
710 INPUT " H,K,L =" ;HAD,KAD,LAD
720 X(1)=HAD:Y(1)=KAD:Z(1)=LAD
730 IF HAD=0 AND KAD=0 AND LAD=0 THEN 750
740 IF 0=U*HAD+V*KAD+W*LAD THEN 760
750 BEEP:PRINT " reinput indices !" :GOTO 710
760 GOSUB *VECTOR
770 IF FNCS(X1,Y1,Z1,X2,Y2,Z2)=>0 THEN 790
780 X2=X2+X1:Y2=Y2+Y1:Z2=Z2+Z1:GOTO 770
790 PRINT " (13) DIAMETER OF DISKS "
800 PRINT " D=1 -- direct beam and above reflection "
810 PRINT " are in contact with each other"
820 PRINT " D<1 -- they are separated"

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830 PRINT "          D>1 -- they overlap each other"
840 INPUT "                                     D=";DA
850 IF DA<0 THEN DA=-DA
860 IF DA=0 THEN DA=1
870 PRINT " (14) Which do you want?"
880 PRINT "          HOLZ-ring ----- 0"
890 PRINT "          HOLZ-line I (circle approximation) ----- 1"
900 PRINT "          HOLZ-line II(more accurate approximation) -- 2"
910 INPUT "                                     ";HLZ
920 OORG$="":OORG=999:HLZ=INT(ABS(HLZ)) MOD 3
930 IF HLZ=2 THEN GOTO 940 ELSE GOTO 990
940 IF GREF$="N" OR GREF$="n" THEN GOTO 990
950 INPUT "          0-disk(O) or G-disk(G)          ";OORG$
960 IF OORG$="O" OR OORG$="o" OR OORG$="G" OR OORG$="g" THEN GOTO 980
970 GOTO 950
980 IF OORG$="O" OR OORG$="o" THEN OORG=1 ELSE OORG=999
990 IF HLZ=0 THEN INTE=0:GOTO 1020
1000 INPUT "          number of step in HOLZ-line ";INTE
1010 INTE=ABS(INTE):IF INTE<10 THEN INTE=10
1020 PRINT:PRINT " (15) Output to the PRINTER ----- 1"
1030 PRINT "          PLOTTER ----- 2"
1040 INPUT "                                     ";PRPL
1050 PRPL=INT(ABS(PRPL)):IF PRPL>2 THEN GOTO 1040
1060 SP=0:IF PRPL=0 THEN GOTO 1040
1070 IF PRPL=1 THEN GOTO 1100
1080 INPUT "          pen number 1-8 ";SP
1090 '*****
1100 CLS 1:LOCATE 18,10 :PRINT "by  PHYS. DEPT. FAC OF SCI. TOHOKU UNIV."
1110 PRINT "          T.KANEYAMA "
1120 GOSUB *ZONE
1130 '
1140 REM ***** construction of reciprocal lattice *****
1150 DREA=SQR(1-COS(ALP)^2-COS(BET)^2-COS(GAM)^2+2*COS(ALP)*COS(BET)*COS(GAM))
1160 DREC=DREA*DREA/(SIN(ALP)*SIN(BET)*SIN(GAM))
1170 VOL=A*B*C*DREA : VOLST=1/VOL
1180 AST=B*C*SIN(ALP)/VOL:BST=C*A*SIN(BET)/VOL:CST=A*B*SIN(GAM)/VOL
1190 COA=(COS(BET)*COS(GAM)-COS(ALP))/(SIN(BET)*SIN(GAM))
1200 COB=(COS(GAM)*COS(ALP)-COS(BET))/(SIN(GAM)*SIN(ALP))
1210 COG=(COS(ALP)*COS(BET)-COS(GAM))/(SIN(ALP)*SIN(BET))
1220 S1A=DREA/(SIN(BET)*SIN(GAM)):S1B=DREA/(SIN(GAM)*SIN(ALP)):SIG=DREA/(SIN(ALP)*SIN(BET))
1230 S11ST=(BST*CST*S1A)^2:S22ST=(CST*AST*S1B)^2:S33ST=(AST*BST*S1G)^2
1240 S12ST=AST*BST*CST*(COA*COB-COG):S23ST=AST*AST*BST*CST*(COB*COG-COA):S31ST=AST*BST*BST*CST*(COG*COA-COB)
1250 D=N*VOLST/SQR(S11ST*U*U+S22ST*V*V+S33ST*W*W+2*S12ST*U*V+2*S23ST*V*W+2*S31ST*W*U)
1260 A1=A:B1=B*COS(GAM):B2=B*DREA/SIN(BET):B3=B*(COS(ALP)-COS(BET)*COS(GAM))/SIN(BET):C1=C*COS(BET):C3=C*SIN(BET)
1270 BST1=0:BST3=0:CST1=0
1280 AST1=1/A:AST2=(COS(ALP)*COS(BET)-COS(GAM))/(A*DREA*SIN(BET)):AST3=-COS(BET)/(A*SIN(BET)):BST2=SIN(BET)/(B*DREA):CST2=(COS(BET)*COS(GAM)-COS(ALP))/(C*DREA*SIN(BET)):CST3=1/(C*SIN(BET))
1290 ' *****
1300 '
1310 UU=A1*U+B1*V+C1*W : VV=A2*U+B2*V+C2*W : WW=A3*U+B3*V+C3*W
1320 RD=FNRL(HAD,KAD,LAD)/2:DDA=DA*RD : DD=1.1*DDA
1330 ' <*> 'DDA' is radius of disk
1340 FA1=SQR(UU*UU+VV*VV) : FA2=SQR(UU*UU+VV*VV+WW*WW)
1350 WN=SQR(1000*E*(1+9.788E-07*1000*E))/12.26:WN2=WN*WN
1360 ' <*> 'WN' is wave number of electron beam
1370 RO=FNRL(HG/2,KG/2,LG/2):R=SQR(RO*RO-D*D+2*D*SQR(WN2-RO*RO))
1380 ' <*> 'R' is radius of HOLZ-ring
1390 RR=SQR(RO*RO+2*D*SQR(WN2-RO*RO))
1400 IF UU*UU+VV*VV<.0001 THEN 1440
1410 X=FNPROX(FNXABC(HAD,KAD,LAD),FNYABC(HAD,KAD,LAD),FNZABC(HAD,KAD,LAD))
1420 Y=FNPROY(FNXABC(HAD,KAD,LAD),FNYABC(HAD,KAD,LAD),FNZABC(HAD,KAD,LAD))
1430 GOTO 1450
1440 X=FNXABC(HAD,KAD,LAD):Y=-FNYABC(HAD,KAD,LAD)
1450 CO=FNCS(1,0,0,X,Y,0):SI=FNCS(0,1,0,X,Y,0)
1460 ' <*> 'CO' and 'SI' are direction cosign
1470 COAV12=SQR(1-FNCS(X1,Y1,Z1,X2,Y2,Z2)^2)
1480 LV1=FNRL(X1,Y1,Z1):NV1=2*(RR+DD+RO)/(LV1*COAV12)
1490 IF NV1<5 THEN NV1=5
1500 O1=0:O2=0:O3=0:I=0:V2=0:QQ=0:NQ1=0:NQ2=0:NQ3=0:NQ4=0
1510 WINXY=R+DDA*2.2
1520 IF R/DDA<10 THEN 1540
1530 WINXY=1.1*WINXY
1540 WINDOW (-WINXY,-WINXY)-(WINXY,WINXY)
1550 VIEW (205,5)-(595,395):CIRCLE(0,0),R
1560 IF GREF$="n" OR GREF$="N" THEN HGP=0:KGP=0:GOTO 1680
1570 IF UU*UU+VV*VV<.0001 THEN 1610
1580 HGPROI=FNPROX(FNXABC(HG/2,KG/2,LG/2),FNYABC(HG/2,KG/2,LG/2),FNZABC(HG/2,KG/2,LG/2))
1590 KGPROI=FNPROY(FNXABC(HG/2,KG/2,LG/2),FNYABC(HG/2,KG/2,LG/2),FNZABC(HG/2,KG/2,LG/2))
1600 GOTO 1620
1610 HGPROI=FNXABC(HG/2,KG/2,LG/2) : KGPROI=-FNYABC(HG/2,KG/2,LG/2)

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1620 HGPRO=HGPROI*CO+KGPROI*SI:KGPRO=-HGPROI*SI+KGPROI*CO
1630 HGP=HGPRO:KGP=KGPRO:CIRCLE(HGPRO,KGPRO),DDA
1640 SX=MAP(-HGPRO,0)-3:SY=MAP(-KGPRO,1)-3
1650 PUT(SX,SY),KANJI(&H14F),OR
1660 SX=MAP(HGPRO,0)-3:SY=MAP(KGPRO,1)-3
1670 PUT(SX,SY),KANJI(&H147),OR
1680 CIRCLE(-HGPRO,-KGPRO),DDA
1690 CLS 1 : GOSUB *LABEL
1700 '
1710 ' ** searchig reciprocal lattice points **
1720 GOSUB *NEARZONE
1730 H=HN : K=KN : L=LN
1740 GOSUB *V1
1750 LL1=FNRL(H-HG/2,K-KG/2,L-LG/2):LL2=FNRL(H+HG/2,K+KG/2,L+LG/2)
1760 IF LL1=>RR+DDA AND LL2=>RR+DDA THEN 1790
1770 GOTO 1740
1780 '
1790 IF I=3 THEN 2030
1800 LL1=FNRL(H-HG/2,K-KG/2,L-LG/2):LL2=FNRL(H+HG/2,K+KG/2,L+LG/2)
1810 P=0:P1=0:P2=0
1820 IF LL1>RR-DDA AND LL1<RR+DDA THEN P1=1:GOTO 1850
1830 IF LL1<=RR-DDA THEN P1=2:GOTO 1850
1840 IF LL1>=RR+DDA THEN P1=3
1850 IF LL2>RR-DDA AND LL2<RR+DDA THEN P2=1:GOTO 1880
1860 IF LL2<=RR-DDA THEN P2=2:GOTO 1880
1870 IF LL2>=RR+DDA THEN P2=3
1880 IF P1=1 OR P2=1 THEN P=1:GOTO 1950
1890 IF P1=2 AND P2=2 THEN P=2:GOTO 1950
1900 P=3
1910 IF P1<>3 OR P2<>3 THEN 1940
1920 '
1930 IF P=3 AND O2<>0 THEN P=4
1940 IF P=4 THEN P4=P4+1
1950 ON P GOSUB *HOLZRING , *V2 , *MV1 , *V2
1960 IF P=1 THEN GOSUB *MV1
1970 IF P=3 AND O2=0 AND O1>NV1 THEN GOSUB *TV
1980 IF P=2 OR P=4 THEN GOTO 1740
1990 IF P=10 THEN 2030
2000 GOTO 1790
2010 ' *****
2020 '
2030 IF O3=0 THEN 2190
2040 '
2050 ' ***** load the program for output *****
2060 COMMON S$,A,B,C,ALPH,BETA,GAMM
2070 COMMON U,V,W,E,N,GREF$,HG,KG,LG,HAD,KAD,LAD,OORG
2080 COMMON AST1,AST2,AST3,BST1,BST2,BST3,CST1,CST2,CST3
2090 COMMON HGP,KGP,CO,SI,DD,DDA,UU,VV,WW,FA1,FA2
2100 COMMON D,WN,WN2,R,HLZ,INTE,SP,O3,HCA(),KCA(),LCA(),DISK()
2110 COLOR 2:LOCATE 30,23:PRINT "HIT RETURN KEY":COLOR 0
2120 HRK$=INKEY$:IF HRK$="" THEN 2120
2130 CLS 3:LOCATE 30,12:PRINT "Now loading"
2140 ON PRPL GOTO 2150,2160
2150 CHAIN "CHPR"
2160 CHAIN "CHPL"
2170 ' *****
2180 END
2190 LOCATE 40,3:BEEP:PRINT " You have no holz."
2200 END
2210 '
2220 ' ((( sub routine )))
2230 '** data input **
2240 *SYS1 'cubic
2250 INPUT " (5) LATTICE PARAMETERS (A' ) a=b=c= ";A
2260 B=A:C=A:ALP=PAI#/2:BET=PAI#/2:GAM=PAI#/2:ALPH=90:BETA=90:GAMM=90
2270 RETURN
2280 *SYS2 'tetragonal
2290 INPUT " (5) LATTICE PARAMETERS (A' ) a=b= ";A
2300 INPUT " c= ";C
2310 B=A:ALP=PAI#/2:BET=PAI#/2:GAM=PAI#/2:ALPH=90:BETA=90:GAMM=90
2320 RETURN
2330 *SYS3 'rhombohedral
2340 INPUT " (5) LATTICE PARAMETERS (A' ) a=b=c= ";A
2350 INPUT " (6) ANGLE (deg) alpha=beta=gamma= ";ALPH
2360 B=A:C=A:ALP=ALPH*PAI#/180:BET=ALP:GAM=ALP:BETA=ALPH:GAMM=ALPH
2370 RETURN
2380 *SYS4 'hexagonal (trigonal,rhombohedral)
2390 INPUT " (5) LATTICE PARAMETERS (A' ) a=b= ";A
2400 INPUT " c= ";C
2410 INPUT " rhombohedral ? (y/n) ";RH$
2420 B=A:ALP=PAI#/2:BET=PAI#/2:GAM=2*PAI#/3:ALPH=90:BETA=90:GAMM=120
2430 RETURN

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2440 *SYS5 'orthorhombic
2450 INPUT " (5) LATTICE PARAMETERS (A' )          a= ";A
2460 INPUT "                                         b= ";B
2470 INPUT "                                         c= ";C
2480 ALP=PAI#/2:BET=PAI#/2:GAM=PAI#/2:ALPH=90:BETA=90:GAMM=90
2490 RETURN
2500 *SYS6 'monoclinic
2510 INPUT " (3) UNIQUE AXIS,B or C ?                ";UNIQS$
2520 IF UNIQS$="B" OR UNIQS$="b" OR UNIQS$="C" OR UNIQS$="c" THEN 2540
2530 GOTO 2510
2540 PRINT " (4) primitive ----- 1"
2550 IF UNIQS$="b" OR UNIQS$="B" THEN 2580
2560 PRINT " B-base centered ----- 2"
2570 GOTO 2590
2580 PRINT " C-base centered ----- 3"
2590 INPUT "                                         ";BRAV
2600 INPUT " (5) LATTICE PARAMETERS (A' )          a= ";A
2610 INPUT "                                         b= ";B
2620 INPUT "                                         c= ";C
2630 IF UNIQS$="c" OR UNIQS$="C" THEN 2660
2640 INPUT " (6) ANGLE (deg)                        beta= ";BETA:GAMM=90
2650 GOTO 2670
2660 INPUT " (6) ANGLE (deg)                        gamma= ";GAMM:BETA=90
2670 ALP=PAI#/2:BET=BETA*PAI#/180:GAM=GAMM*PAI#/180:ALPH=90
2680 IF BRAV=2 THEN BRAV=5
2690 IF BRAV=3 THEN BRAV=6
2700 RETURN 550
2710 *SYS7 'triclinic
2720 INPUT " (5) LATTICE PARAMETERS (A' )          a= ";A
2730 INPUT "                                         b= ";B
2740 INPUT "                                         c= ";C
2750 INPUT " (6) ANGLE (deg)                        alpha= ";ALPH
2760 INPUT "                                         beta= ";BETA
2770 INPUT "                                         gamma= ";GAMM
2780 ALP=ALPH*PAI#/180:BET=BETA*PAI#/180:GAM=GAMM*PAI#/180
2790 RETURN
2800 '
2810 *LABEL ' ** labeling **
2820 LOCATE 2,2:PRINT $$:PRINT
2830 PRINT " [";U;" ";V;" ";W;"]":PRINT
2840 PRINT " "E;"kV":PRINT
2850 PRINT " ";N;
2860 IF N>3 THEN 2910
2870 ON N GOTO 2880,2890,2900
2880 PRINT "st Laue Zone":GOTO 2920
2890 PRINT "nd Laue Zone":GOTO 2920
2900 PRINT "rd Laue Zone":GOTO 2920
2910 PRINT "th Laue Zone"
2920 PRINT
2930 IF GREF$="n" OR GREF$="N" THEN 2960
2940 PRINT " G reflection : "
2950 PRINT " (";HG;" ";KG;" ";LG;" )"
2960 PRINT :PRINT " a =";A;"(A)":PRINT " b =";B;"(A)":PRINT " c =";C;"(A)"
2970 PRINT " alpha,beta,gamma ":PRINT " =";ALPH;" ";BETA;" ";GAMM;"(deg)"
2980 PRINT : PRINT " Radius of N-th Laue Zone"
2990 PRINT " =";R;"(1/A)"
3000 PRINT " Horizontal Direction"
3010 PRINT " = [";HAD;" ";KAD;" ";LAD;" ]*"
3020 RETURN
3030 '
3040 *ZONE' * seach the reciprocal lattice point allowed by extinction rule *
3050 NZNE=1
3060 FOR H=-NZNE TO NZNE
3070 FOR K=-NZNE TO NZNE
3080 FOR L=-NZNE TO NZNE
3090 IF U*H+V*K+W*L=N THEN 3140
3100 NEXT:NEXT:NEXT
3110 NZNE=NZNE+2
3120 IF NZNE>=15 THEN GOTO 3160
3130 GOTO 3060
3140 HN=H:KN=K:LN=L
3150 RETURN
3160 PRINT " cannot find N-th laue zone"
3170 PRINT " indices of reciprocal lattice point in the N-th Laue zone"
3180 INPUT "                                         h,k,l=";H,K,L
3190 IF FNPRO(H,K,L,U,V,W)=N THEN 3140
3200 PRINT " reinput indices":GOTO 3180
3210 '
3220 *NEARZONE
3230 NRL0=FNRL(HN,KN,LN)
3240 FOR NHN1=-1 TO 1
3250 FOR NHN2=-1 TO 1

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3260 IF NHN1=0 AND NHN2=0 THEN GOTO 3330
3270 H=HN+X1*NHN1+X2*NHN2
3280 K=KN+Y1*NHN1+Y2*NHN2
3290 L=LN+Z1*NHN1+Z2*NHN2
3300 NRL1=FNRL(H,K,L)
3310 IF NRL1>=NRLO THEN GOTO 3330
3320 HN=H:KN=K:LN=L:GOTO *NEARZONE
3330 NEXT:NEXT
3340 RETURN
3350 '
3360 *V2
3370 GOSUB *V1
3380 LL1=FNRL(H-HG/2,K-KG/2,L-LG/2)
3390 LL2=FNRL(H+HG/2,K+KG/2,L+LG/2)
3400 IF LL1>RR+DDA AND LL2>RR+DDA THEN 3420
3410 GOTO 3370
3420 H=H+X2*(-1)^I:K=K+Y2*(-1)^I:L=L+Z2*(-1)^I:O1=O:O2=O
3430 RETURN
3440 *MV1
3450 H=H-X1*(-1)^I:K=K-Y1*(-1)^I:L=L-Z1*(-1)^I:O1=O1+1
3460 RETURN
3470 *V1
3480 H=H+X1*(-1)^I : K=K+Y1*(-1)^I : L=L+Z1*(-1)^I
3490 RETURN
3500 *TV
3510 I=I+1
3520 H=H+(P4+1)*X2*(-1)^I : K=K+(P4+1)*Y2*(-1)^I : L=L+(P4+1)*Z2*(-1)^I
3530 IF FNRL(H-HG/2,K-KG/2,L-LG/2)<=RR+DDA THEN 3590
3540 LL1=FNRL(H-HG/2,K-KG/2,L-LG/2):LL2=FNRL(H+HG/2,K+KG/2,L+LG/2)
3550 IF LL1<=RR+DDA AND LL2<=RR+DDA THEN 3590
3560 IF NORI>NV1*2 THEN O3=O3+1:P=10:RETURN
3570 NORI=NORI+1:GOSUB *MV1
3580 GOTO 3530
3590 O1=O:O2=O:P=2:P4=O:NORI=O
3600 RETURN
3610 '
3620 *VECTOR' ** calculate two seaching vector **
3630 FOR I=1 TO 25
3640 READ SO(I):NEXT I
3650 X=U:Y=V:Z=W:GOSUB *SOS:U=X:V=Y:W=Z
3660 X(2)=V*Z(1)-W*Y(1):Y(2)=W*X(1)-U*Z(1):Z(2)=U*Y(1)-V*X(1)
3670 FOR J=1 TO 2
3680 X=X(J):Y=Y(J):Z=Z(J)
3690 GOSUB *SOS
3700 X(J)=X:Y(J)=Y:Z(J)=Z
3710 NEXT J
3720 *VECTOR2
3730 X1A=X(1):Y1A=Y(1):Z1A=Z(1)
3740 X2A=X(2):Y2A=Y(2):Z2A=Z(2)
3750 LV1=FNL(X1A,Y1A,Z1A)
3760 LV2=FNL(X2A,Y2A,Z2A)
3770 FOR V1=-2 TO 2
3780 X(2)=X2A+X(1)*V1:Y(2)=Y2A+Y(1)*V1:Z(2)=Z2A+Z(1)*V1
3790 X=X(2):Y=Y(2):Z=Z(2):GOSUB *SOS:X(2)=X:Y(2)=Y:Z(2)=Z
3800 IF LV2>FNL(X(2),Y(2),Z(2)) THEN GOTO 3740
3810 NEXT V1
3820 X(2)=X2A:Y(2)=Y2A:Z(2)=Z2A
3830 '
3840 X1A=X(1):Y1A=Y(1):Z1A=Z(1)
3850 LV1=FNL(X1A,Y1A,Z1A)
3860 LV2=FNL(X2A,Y2A,Z2A)
3870 FOR V2=-2 TO 2
3880 X(1)=X1A+X(2)*V2:Y(1)=Y1A+Y(2)*V2:Z(1)=Z1A+Z(2)*V2
3890 X=X(1):Y=Y(1):Z=Z(1):GOSUB *SOS:X(1)=X:Y(1)=Y:Z(1)=Z
3900 IF LV1>FNL(X(1),Y(1),Z(1)) THEN GOTO 3840
3910 NEXT V2
3920 X(1)=X1A:Y(1)=Y1A:Z(1)=Z1A
3930 X1=X(1):Y1=Y(1):Z1=Z(1):X2=X(2):Y2=Y(2):Z2=Z(2)
3940 RETURN
3950 '
3960 DATA 2,3,5,7,11,13,17,19,23,29,31,37,41,43
3970 DATA 47,53,59,61,67,71,73,79,83,89,97
3980 *SOS
3990 FOR I=1 TO 6
4000 XX=X-SO(I)*INT(X/SO(I)):YY=Y-SO(I)*INT(Y/SO(I))
4010 ZZ=Z-SO(I)*INT(Z/SO(I))
4020 IF XX=0 AND YY=0 AND ZZ=0 THEN GOTO 4030 ELSE GOTO 4040
4030 X=X/SO(I):Y=Y/SO(I):Z=Z/SO(I):SO2=1:GOTO 4000
4040 NEXT I
4050 IF X>16 OR Y>16 OR Z>16 THEN 4070 ELSE RETURN
4060 '
4070 FOR I=7 TO 12

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4080 XX=X-SO(I)*INT(X/SO(I)):YY=Y-SO(I)*INT(Y/SO(I))
4090 ZZ=Z-SO(I)*INT(Z/SO(I))
4100 IF XX<>0 OR YY<>0 OR ZZ<>0 THEN 4120
4110 X=X/SO(I):Y=Y/SO(I):Z=Z/SO(I):SO2=1:GOTO 4080
4120 NEXT I
4130 IF X>40 OR Y>40 OR Z>40 THEN 4150 ELSE RETURN
4140 '
4150 FOR I=13 TO 25
4160 XX=X-SO(I)*INT(X/SO(I)):YY=Y-SO(I)*INT(Y/SO(I))
4170 ZZ=Z-SO(I)*INT(Z/SO(I))
4180 IF XX<>0 OR YY<>0 OR ZZ<>0 THEN 4200
4190 X=X/SO(I):Y=Y/SO(I):Z=Z/SO(I):SO2=1:GOTO 4160
4200 NEXT I
4210 IF X=0 AND Y=0 THEN Z=SGN(Z):RETURN
4220 IF Y=0 AND Z=0 THEN X=SGN(X):RETURN
4230 IF Z=0 AND X=0 THEN Y=SGN(Y):RETURN
4240 RETURN
4250 '
4260 ' ** extinction rule **          AL=0:allowed    AL#0:forbidden
4270 *DIAMOND
4280 IF 1=FNPARITY(H+K) OR 1=FNPARITY(K+L) THEN 4320
4290 IF 1=FNPARITY(H) THEN 4310
4300 IF 1=FNPARITY((H+K+L)/2) THEN 4320
4310 AL=0:RETURN
4320 AL=1:RETURN
4330 *I ' body centered
4340 AL=FNPARITY(H+K+L)
4350 RETURN
4360 *P ' primitive
4370 AL=0
4380 RETURN
4390 *F ' face centered
4400 AL=FNPARITY(H+K)+FNPARITY(K+L)
4410 RETURN
4420 *A ' A-base centered
4430 AL=FNPARITY(K+L)
4440 RETURN
4450 *B ' B-base centered
4460 AL=FNPARITY(H+L)
4470 RETURN
4480 *C ' C-base centered
4490 AL=FNPARITY(H+K)
4500 RETURN
4510 *RHOMBO ' rhombohedral (hexagonal coordinates)
4520 AL=3*((-H+K+L)/3-INT((-H+K+L)/3))
4530 RETURN
4540 '
4550 *HOLZRING ' ** draw HOLZRING pattern **
4560 O1=0 : O2=O2+1
4570 ON BRAV GOSUB *P,*F,*I,*A,*B,*C,*DIAMOND
4580 IF RH$="Y" OR RH$="y" THEN GOSUB *RHOMBO
4590 IF AL<>0 THEN 4790
4600 O3=O3+1
4610 HCA(O3)=H : KCA(O3)=K : LCA(O3)=L
4620 IF O3=0 OR O3=1 THEN 4640
4630 IF (HCA(O3)-HCA(1))^2<.1 AND (KCA(O3)-KCA(1))^2<.1 AND (LCA(O3)-LCA(1))^2<.1 AND I=2 THEN
P=10:GOTO 4790
4640 DISK(O3)=1
4650 IF P1<>1 THEN DISK(O3)=0:RETURN
4660 IF P2=1 THEN DISK(O3)=2
4670 IF UU*UU+VV*VV<.0001 THEN 4710
4680 XI=FNPROX(FNXABC(H-HG/2,K-KG/2,L-LG/2),FNYABC(H-HG/2,K-KG/2,L-LG/2),FNZABC(H-HG/2,K-KG/2,L-LG/2))
4690 YI=FNPROY(FNXABC(H-HG/2,K-KG/2,L-LG/2),FNYABC(H-HG/2,K-KG/2,L-LG/2),FNZABC(H-HG/2,K-KG/2,L-LG/2))
4700 GOTO 4720
4710 XI=FNXABC(H-HG/2,K-KG/2,L-LG/2):YI=-FNYABC(H-HG/2,K-KG/2,L-LG/2)
4720 X=XI*CO+YI*SI:Y=-XI*SI+YI*CO:CIRCLE(X,Y),DDA
4730 SHKL$=STR$(O3):LHKL=LEN(SHKL$)
4740 SX=MAP(X,O)-3:SY=MAP(Y,1)-3
4750 FOR I1=1 TO LHKL
4760 MHKL$=MID$(SHKL$,I1,1):MHKL=ASC(MHKL$)+256
4770 PUT (SX-4*LHKL+8*(I1-1),SY),KANJI(MHKL),OR
4780 NEXT I1
4790 RETURN
4800 '
4810 END

```

#### CHPR

```

10 REM FILE NAME "CHPR"
20 ' *** output HOLZ for printer ***
30 '
40 ' This program will be chained from program "HOLZ" and .....

```

```

50 ' (1)get hard-copy of CRT screen
60 ' (2)print out Miller indices' list of excited reflections.
70 '
80 CONSOLE ,,0
90 DEF FNPRO(X1,X2,X3,Y1,Y2,Y3)=X1*Y1+X2*Y2+X3*Y3
100 DEF FNRL(H,K,L)=SQR((H*AST1)^2+(H*AST2+K*BST2+L*CST2)^2+(H*AST3+L*CST3)^2)
110 DEF FNXABC(H,K,L)=H*AST1+K*BST1+L*CST1
120 DEF FNYABC(H,K,L)=H*AST2+K*BST2+L*CST2
130 DEF FNZABC(H,K,L)=H*AST3+K*BST3+L*CST3
140 DEF FNPROX(X,Y,Z)=(UU*WW*X+VV*WW*Y-FA1*FA1*Z)/(FA1*FA2)
150 DEF FNPROY(X,Y,Z)=(VV*X-UU*Y)/FA1
160 DEF FNPROZ(X,Y,Z)=-(UU*X+VV*Y+WW*Z)/FA2
170 DEF FNL(X,Y,Z)=X*X+Y*Y+Z*Z
180 '
190 I=0 :HGPRO=HGP:KGP=KGP: CLS 3
200 IF HLZ=0 THEN GOSUB *HOLZRING2
210 XX1=DD*1.05
220 XX4=-XX1:XX5=-XX1:XX8=XX1:YY2=-XX1:YY3=-XX1:YY6=XX1:YY7=XX1
230 INDX=4*DD/240 : INDY=28*DD/240
240 XY1=-DD*5/3-INDY/2
250 XY4=XY1:XY5=-XY1-2.1*INDY:XY8=XY5
260 NQ1=0:NQ4=0:NQ5=0:NQ8=0
270 ON HLZ GOSUB *HOLZ,*HOLZ2
280 GOSUB *POUT:CLS 3
290 PRINT " (14) Which do you want?"
300 PRINT "          HOLZRING ----- 0"
310 PRINT "          HOLZ I (circle approximation) ----- 1"
320 PRINT "          HOLZ II (more accurate approximation) -- 2"
330 PRINT "          E      N      D      ----- 3"
340 INPUT "          ";HLZ
350 OORG=999
360 HLZ=INT(ABS(HLZ)):IF HLZ>3 THEN GOTO 340
370 IF HLZ=2 THEN GOTO 380 ELSE GOTO 430
380 IF GREF$="N" OR GREF$="n" THEN GOTO 430
390 INPUT "          0-disk(0) or G-disk(G) ";OORG$
400 IF OORG$="0" OR OORG$="o" OR OORG$="G" OR OORG$="g" THEN GOTO 420
410 GOTO 390
420 IF OORG$="0" OR OORG$="o" THEN OORG=1 ELSE OORG=999
430 IF HLZ=3 THEN 660
440 IF HLZ=0 THEN 470
450 INPUT "          number of step in HOLZ line ";INTE
460 INTE=ABS(INTE) :IF INTE<10 THEN INTE=10
470 PRINT " (15) Output to the PRINTER ----- 1"
480 PRINT "          PLOTTER ----- 2"
490 INPUT "          ";PRPL
500 PRPL=INT(ABS(PRPL)):IF PRPL>2 THEN GOTO 490
510 IF PRPL=0 THEN GOTO 490
520 IF PRPL=1 THEN CLS 1:GOTO 200
530 INPUT "          pen number 1-8 ";SP
540 SP=INT(ABS(SP)):IF SP>8 THEN GOTO 530
550 CLS 1:COLOR 2:PRINT " Ready the plotter"
560 COMMON S$,A,B,C,ALPH,BETA,GAMM
570 COMMON U,V,W,E,N,GREF$,HG,KG,LG,HAD,KAD,LAD,OORG
580 COMMON AST1,AST2,AST3,BST1,BST2,BST3,CST1,CST2,CST3
590 COMMON HGP,KGP,CO,SI,DD,DDA,UU,VV,WW,FA1,FA2
600 COMMON D,WN,WN2,R,HLZ,INTE,SP,O3,HCA(),KCA(),LCA(),DISK()
610 PRINT:PRINT " Hit return key to start":COLOR 0
620 HRK$=INKEY$:IF HRK$="" THEN 620
630 CLS 1:LOCATE 30,10:PRINT "Now loading"
640 CHAIN "CHPL"
650 GOTO 200
660 CLS 1:END
670 '
680 *LABEL ' ** labeling **
690 LOCATE 2,2:PRINT S$:PRINT
700 PRINT " [{"U" "v" "w"}]":PRINT
710 PRINT " "E;"kv":PRINT
720 PRINT " ";N;
730 IF N>3 THEN 780
740 ON N GOTO 750,760,770
750 PRINT "st Laue Zone":GOTO 790
760 PRINT "nd Laue Zone":GOTO 790
770 PRINT "rd Laue Zone":GOTO 790
780 PRINT "th Laue Zone"
790 PRINT
800 IF GREF$="n" OR GREF$="N" THEN 830
810 PRINT " G reflection : "
820 PRINT " ("HG" "KG" "LG")"
830 PRINT :PRINT " a ="A"(A)":PRINT " b ="B"(A)":PRINT " c ="C"(A)"
840 PRINT " alpha,beta,gamma ":PRINT " ="ALPH","BETA","GAMM"(deg)"
850 PRINT :PRINT " Radius of HOLZ-ring"
860 PRINT " ="R;"(1/A)"

```

```

870 PRINT " Horizontal Direction"
880 PRINT " = [";HAD;"",";KAD;"",";LAD;""]*"
890 RETURN
900 '
910 *HOLZ** draw K-M line by circle approximation **
920 WINDOW (-DD,-DD)-(DD,DD):VIEW (200,80)-(440,320)
930 CIRCLE(0,0),DDA
940 IF R/DDA>100 THEN GOTO *HOLZ100
950 FOR IJ=1 TO 03-1
960 IF DISK(IJ)=0 THEN 1080
970 H=HCA(IJ):K=KCA(IJ):L=LCA(IJ)
980 WINDOW (-DD,-DD)-(DD,DD):VIEW (200,80)-(440,320)
990 IF UU*UU+VV*VV<.0001 THEN 1030
1000 XI=FNPROX(FNXABC(H-HG/2,K-KG/2,L-LG/2),FNYABC(H-HG/2,K-KG/2,L-LG/2),FNZABC(H-HG/2,K-KG/2,L-LG/2))
1010 YI=FNPROY(FNXABC(H-HG/2,K-KG/2,L-LG/2),FNYABC(H-HG/2,K-KG/2,L-LG/2),FNZABC(H-HG/2,K-KG/2,L-LG/2))
1020 GOTO 1040
1030 XI=FNXABC(H-HG/2,K-KG/2,L-LG/2):YI=-FNYABC(H-HG/2,K-KG/2,L-LG/2)
1040 X=XI*CO+YI*SI:Y=-XI*SI+YI*CO:CIRCLE(-X,-Y),R
1050 WINDOW (-DD*8/3,-DD*5/3)-(DD*8/3,DD*5/3)
1060 VIEW (0,0)-(639,399)
1070 GOSUB *INDEXING
1080 NEXT IJ
1090 RETURN
1100 *HOLZ100
1110 IF INTE=0 THEN INTE=10
1120 ANGRAN=SQR(2)*DD/R:SANG=2*ANGRAN/INTE
1130 FOR IJ=1 TO 03-1
1140 IN=0:INA=0
1150 IF DISK(IJ)=0 THEN 1700
1160 H=HCA(IJ):K=KCA(IJ):L=LCA(IJ)
1170 WINDOW (-DD,-DD)-(DD,DD):VIEW (200,80)-(440,320)
1180 IF UU*UU+VV*VV<.0001 THEN 1220
1190 XI=FNPROX(FNXABC(H-HG/2,K-KG/2,L-LG/2),FNYABC(H-HG/2,K-KG/2,L-LG/2),FNZABC(H-HG/2,K-KG/2,L-LG/2))
1200 YI=FNPROY(FNXABC(H-HG/2,K-KG/2,L-LG/2),FNYABC(H-HG/2,K-KG/2,L-LG/2),FNZABC(H-HG/2,K-KG/2,L-LG/2))
1210 GOTO 1230
1220 XI=FNXABC(H-HG/2,K-KG/2,L-LG/2):YI=-FNYABC(H-HG/2,K-KG/2,L-LG/2)
1230 X=XI*CO+YI*SI:Y=-XI*SI+YI*CO
1240 IF X=0 THEN 1280
1250 T=ATN(Y/X)*180/PAI#+90*(1-ABS(X)/X)
1260 T=T-360*(INT((T+360)/360)-1)
1270 P=INT((T+45)/90):P=P-4*INT(P/4):GOTO 1300
1280 IF Y>0 THEN T=90:P=1:GOTO 1300
1290 T=270:P=3
1300 FU1=R*R-(X+DD)*(X+DD):FU2=R*R-(X-DD)*(X-DD)
1310 FU3=R*R-(Y+DD)*(Y+DD):FU4=R*R-(Y-DD)*(Y-DD)
1320 ON P+1 GOTO 1330,1390,1450,1510
1330 KXS=-X+SQR(FU3):KYS=DD:KXL=-X+SQR(FU4):KYL=-DD:ANGSL=-1
1340 IF KXS>DD THEN KXS=DD :KYS=-Y-SQR(FU1)
1350 IF KXS<-DD THEN KXS=-DD :KYS=-Y+SQR(FU2)
1360 IF KXL>DD THEN KXL=DD :KYL=-Y+SQR(FU1)
1370 IF KXL<-DD THEN KXL=-DD :KYL=-Y-SQR(FU2)
1380 GOTO 1570
1390 KXS=DD:KYS=-Y+SQR(FU1):KXL=-DD:KYL=-Y+SQR(FU2):ANGSL=1
1400 IF KYS>DD THEN KXS=-X-SQR(FU3):KYS=DD
1410 IF KYS<-DD THEN KXS=-X+SQR(FU4):KYS=-DD
1420 IF KYL>DD THEN KXL=-X+SQR(FU3):KYL=DD
1430 IF KYL<-DD THEN KXL=-X-SQR(FU4):KYL=-DD
1440 GOTO 1570
1450 KXS=-X-SQR(FU3):KYS=DD:KXL=-X-SQR(FU4):KYL=-DD:ANGSL=1
1460 IF KXS>DD THEN KXS=DD :KYS=-Y+SQR(FU1)
1470 IF KXS<-DD THEN KXS=-DD :KYS=-Y-SQR(FU2)
1480 IF KXL>DD THEN KXL=DD :KYL=-Y-SQR(FU1)
1490 IF KXL<-DD THEN KXL=-DD :KYL=-Y+SQR(FU2)
1500 GOTO 1570
1510 KXS=DD:KYS=-Y-SQR(FU1):KXL=-DD:KYL=-Y-SQR(FU2):ANGSL=-1
1520 IF KYS>DD THEN KXS=-X+SQR(FU3):KYS=DD
1530 IF KYS<-DD THEN KXS=-X-SQR(FU4):KYS=-DD
1540 IF KYL>DD THEN KXL=-X-SQR(FU3):KYL=DD
1550 IF KYL<-DD THEN KXL=-X+SQR(FU4):KYL=-DD
1560 '
1570 PSET(KXS,KYS)
1580 FOR ANG=-ANGRAN TO ANGRAN STEP SANG
1590 ANGLE=T*PAI#/180+ANG*ANGSL
1600 XPLOT=R*COS(ANGLE)-X:YPLLOT=R*SIN(ANGLE)-Y
1610 IF ABS(XPLOT)>DD OR ABS(YPLLOT)>DD THEN 1630
1620 LINE -(XPLOT,YPLLOT):IN=1
1630 NEXT ANG
1640 IF IN=0 THEN 1700
1650 LINE -(KXL,KYL)
1660 '
1670 WINDOW (-DD*8/3,-DD*5/3)-(DD*8/3,DD*5/3)
1680 VIEW (0,0)-(639,399)

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```

1690 GOSUB *INDEXING
1700 NEXT IJ
1710 RETURN
1720 '
1730 *INDEXING ' ** index on the K-M pattern **
1740 IF X=0 AND Y>0 THEN P=3 : GOTO *SEP
1750 IF X=0 AND Y<0 THEN P=7 : GOTO *SEP
1760 IF X>0 AND Y=0 THEN P=4 : GOTO *SEP
1770 IF X<0 AND Y=0 THEN P=1 : GOTO *SEP
1780 RAT=Y/X
1790 IF RAT>-1 AND RAT<0 AND X<0 THEN P=1 : GOTO *SEP
1800 IF RAT<=-1 AND X<0 THEN P=2 : GOTO *SEP
1810 IF RAT>=1 AND X>0 THEN P=3 : GOTO *SEP
1820 IF RAT>0 AND RAT<1 AND X>0 THEN P=4 : GOTO *SEP
1830 IF RAT>-1 AND RAT<0 AND X>0 THEN P=5 : GOTO *SEP
1840 IF RAT<=-1 AND X>0 THEN P=6 : GOTO *SEP
1850 IF RAT>=1 AND X<0 THEN P=7 : GOTO *SEP
1860 IF RAT>0 AND RAT<1 AND X<0 THEN P=8 : GOTO *SEP
1870 BEEP:RETURN
1880 *SEP
1890 IF HLZ=2 THEN 1930
1900 FU1=R*R-(X+DD)*(X+DD):FU2=R*R-(X-DD)*(X-DD):FU3=R*R-(Y+DD)*(Y+DD):FU4=R*R-(Y-DD)*(Y-DD)
1910 ON P GOSUB *P1,*P2,*P3,*P4,*P5,*P6,*P7,*P8
1920 GOTO 1940
1930 GOSUB *SEP2
1940 ON Q GOSUB *Q1,*Q2,*Q3,*Q4,*Q5,*Q6,*Q7,*Q8
1950 RETURN
1960 *SEP2
1970 ON P GOTO 1980,2050,2120,1980,2190,2120,2050,2190
1980 EKS=KXS:WAI=KYS ' P=1,4
1990 IF ABS(WAI)<DD THEN GOTO 2020
2000 IF EKS<0 THEN Q=6 ELSE Q=7
2010 RETURN
2020 EKS=KXL:WAI=KYL
2030 IF EKS>0 THEN Q=2 ELSE Q=3
2040 RETURN
2050 EKS=KXS:WAI=KYS ' P=2,7
2060 IF ABS(EKS)<DD THEN GOTO 2090
2070 IF WAI>0 THEN Q=8 ELSE Q=1
2080 RETURN
2090 EKS=KXL:WAI=KYL
2100 IF WAI<0 THEN Q=4 ELSE Q=5
2110 RETURN
2120 EKS=KXL:WAI=KYL ' P=3,6
2130 IF ABS(EKS)<DD THEN GOTO 2160
2140 IF WAI<0 THEN Q=4 ELSE Q=5
2150 RETURN
2160 EKS=KXS:WAI=KYS
2170 IF WAI>0 THEN Q=8 ELSE Q=1
2180 RETURN
2190 EKS=KXL:WAI=KYL ' P=5,8
2200 IF ABS(WAI)<DD THEN GOTO 2230
2210 IF EKS>0 THEN Q=2 ELSE Q=3
2220 RETURN
2230 EKS=KXS:WAI=KYS
2240 IF EKS<0 THEN Q=6 ELSE Q=7
2250 RETURN
2260 '
2270 *P1
2280 IF FU4<0 THEN 2320
2290 EKS=-X-FU4^.5:IF ABS(EKS)>DD THEN 2320
2300 IF EKS>=0 THEN Q=2 ELSE Q=3
2310 RETURN
2320 EKS=-X-FU3^.5:IF EKS>0 THEN Q=7 ELSE Q=6
2330 RETURN
2340 *P2
2350 IF FU1<0 THEN 2390
2360 WAI=-Y+FU1^.5:IF ABS(WAI)>DD THEN 2390
2370 IF WAI<0 THEN Q=1 ELSE Q=8
2380 RETURN
2390 WAI=-Y+FU2^.5:IF WAI=<0 THEN Q=4 ELSE Q=5
2400 RETURN
2410 *P3
2420 IF FU2<0 THEN 2460
2430 WAI=-Y+FU2^.5:IF ABS(WAI)>DD THEN 2460
2440 IF WAI<=0 THEN Q=4 ELSE Q=5
2450 RETURN
2460 WAI=-Y+FU1^.5:IF WAI<0 THEN Q=1 ELSE Q=8
2470 RETURN
2480 *P4
2490 IF FU4<0 THEN 2530
2500 EKS=-X+FU4^.5:IF ABS(EKS)>DD THEN 2530

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```

2510 IF EKS>0 THEN Q=2 ELSE Q=3
2520 RETURN
2530 EKS=-X+FU3^.5:IF EKS>0 THEN Q=7 ELSE Q=6
2540 RETURN
2550 *P5
2560 IF FU3<0 THEN 2600
2570 EKS=-X+FU3^.5:IF ABS(EKS)>DD THEN 2600
2580 IF EKS>0 THEN Q=7 ELSE Q=6
2590 RETURN
2600 EKS=-X+FU4^.5:IF EKS>0 THEN Q=2 ELSE Q=3
2610 RETURN
2620 *P6
2630 IF FU2<0 THEN 2670
2640 WAI=-Y-FU2^.5:IF ABS(WAI)>DD THEN 2670
2650 IF WAI<0 THEN Q=4 ELSE Q=5
2660 RETURN
2670 WAI=-Y-FU1^.5:IF WAI<0 THEN Q=1 ELSE Q=8
2680 RETURN
2690 *P7
2700 IF FU1<0 THEN 2740
2710 WAI=-Y-FU1^.5:IF ABS(WAI)>DD THEN 2740
2720 IF WAI<0 THEN Q=1 ELSE Q=8
2730 RETURN
2740 WAI=-Y-FU2^.5:IF WAI<0 THEN Q=4 ELSE Q=5
2750 RETURN
2760 *P8
2770 IF FU3<0 THEN 2810
2780 EKS=-X-FU3^.5:IF ABS(EKS)>DD THEN 2810
2790 IF EKS>0 THEN Q=7 ELSE Q=6
2800 RETURN
2810 EKS=-X-FU4^.5:IF EKS>0 THEN Q=2 ELSE Q=3
2820 RETURN
2830 '
2840 *POUT ' ** print out **
2850 LPRINT
2860 IF HLZ=0 THEN 3040
2870 IF N=>4 THEN 2890
2880 ON N GOTO 2900,2910,2920
2890 LPRINT " *SS$" ["U""V""W"] "N"th zone "E"kv":GOTO 2930
2900 LPRINT " *SS$" ["U""V""W"] 1 st zone "E"kv":GOTO 2930
2910 LPRINT " *SS$" ["U""V""W"] 2 nd zone "E"kv":GOTO 2930
2920 LPRINT " *SS$" ["U""V""W"] 3 rd zone "E"kv"
2930 IF GREF$="n" OR GREF$="N" THEN 2990
2940 '
2950 IF OORG=1 THEN 2960 ELSE 2970
2960 LPRINT " 0 0 0 disk";:GOTO 2980
2970 LPRINT " ";HG;KG;LG;"disk";
2980 LPRINT " (";HG;KG;LG;"excitation)":GOTO 3000
2990 LPRINT " 0 0 0 disk"
3000 LPRINT " a=";A;"A";" ,b=";B;"A";" ,c=";C;"A"
3010 LPRINT " alpha,beta,gamma=";ALPH;" ,";BETA;" ,";GAMM;"deg"
3020 LPRINT " Radius of HOLZ-ring =";R;"(1/A)"
3030 LPRINT " Horizontal Direction = [";HAD;" ,";KAD;" ,";LAD;"]*"
3040 COPY 3
3050 LPRINT " * indices list *"
3060 JI=FIX((O3-1)/3)+1
3070 FOR IJ=1 TO JI
3080 IF IJ+JI>O3-1 THEN 3120
3090 IF IJ+JI*2>O3-1 THEN 3110
3100 LPRINT IJ"-" ("HCA(IJ)","KCA(IJ)","LCA(IJ)"), IJ+JI"-" ("HCA(IJ+JI)","KCA(IJ+JI)","LCA(IJ+JI)"),
IJ+JI*2"-" ("HCA(IJ+JI*2)","KCA(IJ+JI*2)","LCA(IJ+JI*2)":GOTO 3130
3110 LPRINT IJ"-" ("HCA(IJ)","KCA(IJ)","LCA(IJ)"), IJ+JI"-" ("HCA(IJ+JI)","KCA(IJ+JI)","LCA(IJ+JI)"):
GOTO 3130
3120 LPRINT IJ"-" ("HCA(IJ)","KCA(IJ)","LCA(IJ)")
3130 NEXT IJ
3140 RETURN
3150 '
3160 *HOLZRING2 '** draw HOLZRING pattern **
3170 WINXY=R+DDA*2.2
3180 IF R/DDA<10 THEN 3200
3190 WINXY=1.1*WINXY
3200 WINDOW (-WINXY,-WINXY)-(WINXY,WINXY)
3210 VIEW (205,5)-(595,395):CIRCLE(0,0),R
3220 IF GREF$="n" OR GREF$="N" THEN 3270
3230 SX=MAP(-HGPRO,0)-3:SY=MAP(-KGPRO,1)-3
3240 PUT(SX,SY),KANJI(&H14F)
3250 SX=MAP(HGPRO,0)-3:SY=MAP(KGPRO,1)-3
3260 PUT(SX,SY),KANJI(&H147)
3270 CIRCLE(HGPRO,KGPRO),DDA : CIRCLE(-HGPRO,-KGPRO),DDA
3280 GOSUB *LABEL
3290 FOR J=1 TO O3-1
3300 H=HCA(J) : K=KCA(J) : L=LCA(J)

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3310 IF DISK(J)=0 THEN 3440
3320 IF UU*UU+VV*VV<.0001 THEN 3360
3330 XI=FNPROX(FNXABC(H-HG/2,K-KG/2,L-LG/2),FNYABC(H-HG/2,K-KG/2,L-LG/2),FNZABC(H-HG/2,K-KG/2,L-LG/2))
3340 YI=FNPROY(FNXABC(H-HG/2,K-KG/2,L-LG/2),FNYABC(H-HG/2,K-KG/2,L-LG/2),FNZABC(H-HG/2,K-KG/2,L-LG/2))
3350 GOTO 3370
3360 XI=FNXABC(H-HG/2,K-KG/2,L-LG/2):YI=-FNYABC(H-HG/2,K-KG/2,L-LG/2)
3370 X=XI*CO+YI*SI:Y=-XI*SI+YI*CO:CIRCLE(X,Y),DDA
3380 SHKL$=STR$(J):LHKL=LEN(SHKL$)
3390 SX=MAP(X,0)-3:SY=MAP(Y,1)-3
3400 FOR I1=1 TO LHKL
3410 MHKL$=MID$(SHKL$,I1,1):MHKL=ASC(MHKL$)+256
3420 PUT (SX-4*LHKL+8*(I1-1),SY),KANJI(MHKL),OR
3430 NEXT I1
3440 NEXT J
3450 RETURN
3460 '
3470 *Q1
3480 IF NQ1+NQ8>66 THEN BEEP:RETURN
3490 NQ1=NQ1+1 : XX1=XX1+INDX
3500 IF NQ1-3*INT(NQ1/3)<>1 THEN 3520
3510 XY1=XY1-2*INDX+INDY : XX1=XX1+INDX/2
3520 LINE(DD,WAI)-(XX1,WAI) : LINE(XX1,WAI)-(XX1,XY1)
3530 LINE(XX1,XY1)-(1.8*DD,XY1)
3540 LOCATE 67+4*(NQ1-1-3*INT((NQ1-1)/3)),INT((NQ1-1)/3):PRINT IJ
3550 XY1=XY1+INDX
3560 RETURN
3570 *Q2
3580 IF NQ1+NQ8>66 THEN BEEP:RETURN
3590 NQ1=NQ1+1 : XX1=XX1+INDX : YY2=YY2-INDX
3600 IF NQ1-3*INT(NQ1/3)<>1 THEN GOTO 3620
3610 XY1=XY1-2*INDX+INDY : XX1=XX1+INDX/2 : YY2=YY2-INDX
3620 LINE(EKS,-DD)-(EKS,YY2) : LINE(EKS,YY2)-(XX1,YY2)
3630 LINE(XX1,YY2)-(XX1,XY1) : LINE(XX1,XY1)-(1.8*DD,XY1)
3640 LOCATE 67+4*(NQ1-1-3*INT((NQ1-1)/3)),INT((NQ1-1)/3):PRINT IJ
3650 XY1=XY1+INDX
3660 RETURN
3670 *Q3
3680 IF NQ4+NQ5>66 THEN BEEP:RETURN
3690 NQ4=NQ4+1 : XX4=XX4-INDX : YY3=YY3-INDX
3700 IF NQ4-3*INT(NQ4/3)<>1 THEN GOTO 3720
3710 XY4=XY4-2*INDX+INDY : XX4=XX4-INDX/2 : YY3=YY3-INDX
3720 LINE(EKS,-DD)-(EKS,YY3) : LINE(EKS,YY3)-(XX4,YY3)
3730 LINE(XX4,YY3)-(XX4,XY4) : LINE(XX4,XY4)-(-1.8*DD,XY4)
3740 LOCATE 1+4*(NQ4-1-3*INT((NQ4-1)/3)),INT((NQ4-1)/3):PRINT IJ
3750 XY4=XY4+INDX
3760 RETURN
3770 *Q4
3780 IF NQ4+NQ5>66 THEN BEEP:RETURN
3790 NQ4=NQ4+1 : XX4=XX4-INDX
3800 IF NQ4-3*INT(NQ4/3)<>1 THEN 3820
3810 XY4=XY4-2*INDX+INDY : XX4=XX4-INDX/2
3820 LINE(-DD,WAI)-(XX4,WAI) : LINE(XX4,WAI)-(XX4,XY4)
3830 LINE(XX4,XY4)-(-1.8*DD,XY4)
3840 LOCATE 1+4*(NQ4-1-3*INT((NQ4-1)/3)),INT((NQ4-1)/3):PRINT IJ
3850 XY4=XY4+INDX
3860 RETURN
3870 *Q5
3880 IF NQ4+NQ5>66 THEN BEEP:RETURN
3890 NQ5=NQ5+1 : XX5=XX5-INDX
3900 IF NQ5-3*INT(NQ5/3)<>1 THEN 3920
3910 XY5=XY5-4*INDX-INDY : XX5=XX5-INDX/2
3920 LINE(-DD,WAI)-(XX5,WAI) : LINE(XX5,WAI)-(XX5,XY5)
3930 LINE(XX5,XY5)-(-1.8*DD,XY5)
3940 LOCATE 1+4*(NQ5-1-3*INT((NQ5-1)/3)),22-INT((NQ5-1)/3):PRINT IJ
3950 XY5=XY5+INDX
3960 RETURN
3970 *Q6
3980 IF NQ4+NQ5>66 THEN BEEP:RETURN
3990 NQ5=NQ5+1 : XX5=XX5-INDX : YY6=YY6+INDX
4000 IF NQ5-3*INT(NQ5/3)<>1 THEN GOTO 4020
4010 XY5=XY5-4*INDX-INDY : XX5=XX5-INDX/2 : YY6=YY6+INDX
4020 LINE(EKS,DD)-(EKS,YY6) : LINE(EKS,YY6)-(XX5,YY6)
4030 LINE(XX5,YY6)-(XX5,XY5) : LINE(XX5,XY5)-(-1.8*DD,XY5)
4040 LOCATE 1+4*(NQ5-1-3*INT((NQ5-1)/3)),22-INT((NQ5-1)/3):PRINT IJ
4050 XY5=XY5+INDX
4060 RETURN
4070 *Q7
4080 IF NQ1+NQ8>66 THEN BEEP:RETURN
4090 NQ8=NQ8+1 : XX8=XX8+INDX : YY7=YY7+INDX
4100 IF NQ8-3*INT(NQ8/3)<>1 THEN GOTO 4120
4110 XY8=XY8-4*INDX-INDY : XX8=XX8+INDX/2 : YY7=YY7+INDX
4120 LINE(EKS,DD)-(EKS,YY7) : LINE(EKS,YY7)-(XX8,YY7)

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```

4130 LINE (XX8,YY7)-(XX8,XY8) : LINE (XX8,XY8)-(1.8*DD,XY8)
4140 LOCATE 67+4*(NQ8-1-3*INT((NQ8-1)/3)),22-INT((NQ8-1)/3):PRINT IJ
4150 XY8=XY8+INDX
4160 RETURN
4170 *Q8
4180 IF NQ1+NQ8>66 THEN BEEP:RETURN
4190 NQ8=NQ8+1 : XX8=XX8+INDX
4200 IF NQ8-3*INT(NQ8/3)<>1 THEN 4220
4210 XY8=XY8-4*INDX-INDY : XX8=XX8+INDX/2
4220 LINE (DD,WAI)-(XX8,WAI) : LINE (XX8,WAI)-(XX8,XY8)
4230 LINE (XX8,XY8)-(1.8*DD,XY8)
4240 LOCATE 67+4*(NQ8-1-3*INT((NQ8-1)/3)),22-INT((NQ8-1)/3):PRINT IJ
4250 XY8=XY8+INDX
4260 RETURN
4270 '
4280 *HOLZ2
4290 FOR I=0 TO 1
4300 IF I=OORG THEN GOTO 4780
4310 WINDOW (-DD,-DD)-(DD,DD):VIEW (200,80)-(440,320)
4320 CIRCLE(0,0),DDA
4330 FOR IJ=1 TO 03-1
4340 IF DISK(IJ)=I THEN GOTO 4760
4350 WINDOW (-DD,-DD)-(DD,DD):VIEW (200,80)-(440,320)
4360 H=HCA(IJ):K=KCA(IJ):L=LCA(IJ)
4370 IF UU*UU+VV*VV<.0001 THEN 4410
4380 XI=FNPROX(FNXABC(H,K,L),FNYABC(H,K,L),FNZABC(H,K,L))
4390 YI=FNPROY(FNXABC(H,K,L),FNYABC(H,K,L),FNZABC(H,K,L))
4400 GOTO 4420
4410 XI=FNXABC(H,K,L):YI=-FNYABC(H,K,L)
4420 X=XI*CO+YI*SI:Y=-XI*SI+YI*CO
4430 IF I=0 THEN 4450
4440 IF ABS(FNPRO(X,Y,0,HGPRO,KGPRO,0))<.0001 THEN 4760
4450 IN=0:INA=0:KXS=0:KYS=0:KXL=0:KYL=0
4460 GG=X*X+Y*Y+D*D
4470 GOSUB *BRAGGSL
4480 PSET (KXS,KYS)
4490 IF X=0 THEN 4510
4500 IF ABS(Y/X)<1 THEN 4580
4510 FOR II=0 TO INTE
4520 KX=-DD+2*II*DD/INTE+HGPRO*(-1)^I
4530 GOSUB *BRAGG1
4540 IF BR=0 THEN 4560
4550 GOSUB *PLOT
4560 NEXT II
4570 GOTO 4710
4580 FOR II=0 TO INTE
4590 KY=-DD+2*II*DD/INTE+KGPRO*(-1)^I
4600 GOSUB *BRAGG2
4610 IF BR=0 THEN 4630
4620 GOSUB *PLOT
4630 NEXT II
4640 GOTO 4710
4650 *PLOT
4660 KX=KX-HGPRO*(-1)^I:KY=KY-KGPRO*(-1)^I
4670 IF ABS(KX)>DD OR ABS(KY)>DD THEN IN=0 ELSE IN=1
4680 IF IN=0 THEN RETURN
4690 LINE -(-KX,-KY):INA=1
4700 RETURN
4710 IF INA=0 THEN 4760
4720 LINE -(KXL,KYL)
4730 WINDOW (-DD*8/3,-DD*5/3)-(DD*8/3,DD*5/3)
4740 VIEW (0,0)-(639,399)
4750 GOSUB *INDEXING
4760 NEXT IJ
4770 IF GREF$="N" OR GREF$="n" THEN 4790
4780 NEXT I
4790 RETURN
4800 '
4810 *BRAGG1
4820 AA=4*(Y*Y+D*D)
4830 BB=2*(2*KX*X*Y-GG*Y)
4840 CC=4*(X*X+D*D)*KX*KX-4*GG*X*KX+GG*GG-4*D*D*WN2
4850 DDD=BB*BB-AA*CC:BR=1:IF DDD<0 THEN BR=0 :GOTO 4870
4860 KY=(-BB-ABS(Y)/Y*SQR(DDD))/AA
4870 RETURN
4880 *BRAGG2
4890 AA=4*(X*X+D*D)
4900 BB=2*(2*KY*X*Y-GG*X)
4910 CC=4*(Y*Y+D*D)*KY*KY-4*GG*Y*KY+GG*GG-4*D*D*WN2
4920 DDD=BB*BB-AA*CC:BR=1:IF DDD<0 THEN BR=0 :GOTO 4940
4930 KX=(-BB-ABS(X)/X*SQR(DDD))/AA
4940 RETURN

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```

4950 '
4960 *BRAGGSL
4970 FOR BSL=1 TO 2
4980 IF X=0 THEN 5000
4990 IF ABS(Y/X)<1 THEN 5160
5000 KX=DD*(-1)^BSL+HGPRO*(-1)^I
5010 GOSUB *BRAGG1
5020 KX=KX-HGPRO*(-1)^I:KY=KY-KGPRO*(-1)^I
5030 IF ABS(KY)>DD THEN IN=0 ELSE IN=1
5040 IF IN=1 THEN 5130
5050 FOR J=1 TO 2
5060 KY=DD*(-1)^J+KGPRO*(-1)^I
5070 GOSUB *BRAGG2
5080 KX=KX-HGPRO*(-1)^I:KY=KY-KGPRO*(-1)^I
5090 IF ABS(KX)>DD THEN IN=0 ELSE IN=1
5100 IF IN=1 THEN 5130
5110 NEXT J
5120 BEEP:RETURN 4760
5130 ON BSL GOTO 5140,5150
5140 KXS=-KX:KYS=-KY:GOTO 5320
5150 KXL=-KX:KYL=-KY:GOTO 5320
5160 KY=DD*(-1)^BSL+KGPRO*(-1)^I
5170 GOSUB *BRAGG2
5180 KX=KX-HGPRO*(-1)^I:KY=KY-KGPRO*(-1)^I
5190 IF ABS(KX)>DD THEN IN=0 ELSE IN=1
5200 IF IN=1 THEN 5290
5210 FOR J=1 TO 2
5220 KX=DD*(-1)^J+HGPRO*(-1)^I
5230 GOSUB *BRAGG1
5240 KX=KX-HGPRO*(-1)^I:KY=KY-KGPRO*(-1)^I
5250 IF ABS(KY)>DD THEN IN=0 ELSE IN=1
5260 IF IN=1 THEN 5290
5270 NEXT J
5280 BEEP:RETURN 4760
5290 ON BSL GOTO 5300,5310
5300 KXS=-KX:KYS=-KY:GOTO 5320
5310 KXL=-KX:KYL=-KY
5320 NEXT BSL
5330 RETURN

```

### CHPL

```

10 REM FILE NAME "CHPL"
20 ' *** output HOLZ for X-Y Plotter Roland DXY-990 ***
30 '
40 ' This program will be chained from program "HOLZ" and
50 ' draw Holzring and Holzlines (circle approximation and exact Bragg's
60 ' equation) on the x-y plotter.
70 '
80 CONSOLE , ,0
90 DEF FNPRO(X1,X2,X3,Y1,Y2,Y3)=X1*Y1+X2*Y2+X3*Y3
100 DEF FNRL(H,K,L)=SQR((H*AST1)^2+(H*AST2+K*BST2+L*CST2)^2+(H*AST3+L*CST3)^2)
110 DEF FNXABC(H,K,L)=H*AST1+K*BST1+L*CST1
120 DEF FNYABC(H,K,L)=H*AST2+K*BST2+L*CST2
130 DEF FNZABC(H,K,L)=H*AST3+K*BST3+L*CST3
140 DEF FNPX(X,Y,Z)=(UU*WW*X+VV*WW*Y-FA1*FA1*Z)/(FA1*FA2)
150 DEF FNPROY(X,Y,Z)=(VV*X-UU*Y)/FA1
160 DEF FNPROZ(X,Y,Z)=-((UU*X+VV*Y+WW*Z)/FA2)
170 DEF FNL(X,Y,Z)=X*X+Y*Y+Z*Z
180 PAI#=3.14159265359#
190 '
200 I=0 :HGPRO=HGP:KGPRO=-KGP
210 DDSC=FIX(DD*1E+06)/10000!
220 HGPRO=FIX(HGPRO*1E+06)/1E+06:KGPRO=FIX(KGPRO*1E+06)/1E+06
230 PLDDA=FIX(DDA*1E+06)/10000!:PLDD=FIX(DD*1E+06)/10000!:PLR=100*R
240 DDA=FIX(DDA*1E+06)/1E+06
250 CLS 1:LOCATE 33,12:PRINT "plotting"
260 IF HLZ=0 THEN GOSUB *HOLZRING2
270 ON HLZ GOSUB *HOLZ,*HOLZ2
280 GOSUB *LABEL
290 CLS 3
300 PRINT " (14) Which do you want?"
310 PRINT " HOLZRING ----- 0"
320 PRINT " HOLZ I (circle approximation) ----- 1"
330 PRINT " HOLZ II(more accurate approximation) -- 2"
340 PRINT " E N D ----- 3"
350 INPUT " ";HLZ
360 OORG=999
370 HLZ=INT(ABS(HLZ)):IF HLZ>3 THEN GOTO 350
380 IF HLZ=2 THEN GOTO 390 ELSE GOTO 440
390 IF GREF$="N" OR GREF$="n" THEN GOTO 440
400 INPUT " 0-disk(0) or G-disk(G) ";OORG$

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410 IF OORG$="o" OR OORG$="O" OR OORG$="G" OR OORG$="g" THEN GOTO 430
420 GOTO 400
430 IF OORG$="o" OR OORG$="O" THEN OORG=1 ELSE OORG=999
440 IF HLZ=3 THEN 670
450 IF HLZ=0 THEN 480
460 INPUT "          number of step in HOLZ line ";INTE
470 INTE=ABS(INTE) :IF INTE<10 THEN INTE=10
480 PRINT " (15) Output to the PRINTER ----- 1"
490 PRINT "          PLOTTER ----- 2"
500 INPUT "          ";PRPL
510 PRPL=FIX(ABS(PRPL)):IF PRPL>2 THEN GOTO 500
520 IF PRPL=0 THEN GOTO 500
530 IF PRPL=2 THEN GOTO 640
540 CLS 1:COLOR 2:PRINT "          Ready the printer"
550 COMMON S$,A,B,C,ALPH,BETA,GAMM
560 COMMON U,V,W,E,N,GREF$,HG,KG,LG,HAD,KAD,LAD,OORG
570 COMMON AST1,AST2,AST3,BST1,BST2,BST3,CST1,CST2,CST3
580 COMMON HGP,KGP,CO,SI,DD,DDA,UU,VV,WW,FA1,FA2
590 COMMON D,WN,WN2,R,HLZ,INTE,SP,03,HCA(),KCA(),LCA(),DISK()
600 PRINT:PRINT "          Hit return key to start":COLOR 0
610 HRK$=INKEY$:IF HRK$="" THEN 610
620 CLS 1:LOCATE 30,10:PRINT "Now loading"
630 CHAIN "CHPR"
640 INPUT "          pen number 1-8          ";SP
650 SP=FIX(ABS(SP)):IF SP>8 THEN GOTO 640
660 GOTO 250
670 CLS 1:END
680 '
690 *LABEL ' ** labeling **
700 LPRINT "IN;DF;SP";SP;" "
710 LPRINT "IPO,0,4000,7200;IW;"
720 LPRINT "SCO,100,0,180;"
730 LPRINT "PU;PA5,165;SIO.54,0.8;LB";S$;CHR$(3)
740 LPRINT "PA10,150;SIO.33,0.5;LB[";U;V;W;"]";CHR$(3)
750 LPRINT "PA15,138;SIO.33,0.5;LB";E;"kv";CHR$(3)
760 LPRINT "PA12,128;SIO.26,0.4;LB";N;
770   IF N>3 THEN GOTO 820
780   ON N GOTO 790,800,810
790   LPRINT "st";:GOTO 830
800   LPRINT "nd";:GOTO 830
810   LPRINT "rd";:GOTO 830
820   LPRINT "th";:GOTO 830
830 LPRINT " Laue Zone";CHR$(3)
840 'LPRINT "PA10,116;SIO.32,0.5;LBG=";HG;KG;LG;CHR$(3)
850 IF HLZ<>0 THEN GOTO 870
860 LPRINT "PA10,115;SIO.32,0.5;LBHolz-ring";CHR$(3):GOTO 900
870 IF OORG<>1 THEN GOTO 890
880 LPRINT "PA10,115;SIO.3,0.5;LB";0;0;0;"disk";CHR$(3):GOTO 900
890 LPRINT "PA10,115;SIO.3,0.5;LB";HG;KG;LG;"disk";CHR$(3)
900 LPRINT "PA5,106;SIO.2,0.4;LB( G=";HG;KG;LG;" excitation )";CHR$(3)
910 LPRINT "PA12,96;SIO.26,0.39;Lba=";CHR$(8);A;CHR$(8);CHR$(3);";CS7;LB";CHR$(80);CHR$(3);"CS;"
920 LPRINT "PA12,89;Lbb=";CHR$(8);B;CHR$(8);CHR$(3);";CS7;LB";CHR$(80);CHR$(3);";CS;"
930 LPRINT "PA12,82;Lbc=";CHR$(8);C;CHR$(8);CHR$(3);";CS7;LB";CHR$(80);CHR$(3);";CS;"
940 LPRINT "PA12,75;Lbalpha=";CHR$(8);ALPH;CHR$(8);CHR$(3);"CS8;LB";CHR$(95);CHR$(3);"CS;"
950 LPRINT "PA12,68;Lbbeta =";CHR$(8);BETA;CHR$(8);CHR$(3);"CS8;LB";CHR$(95);CHR$(3);"CS;"
960 LPRINT "PA12,61;LBgamma=";CHR$(8);GAMM;CHR$(8);CHR$(3);"CS8;LB";CHR$(95);CHR$(3);"CS;"
970 LPRINT "PA12,50;SIO.2,0.3;LBRADIUS OF HOLZRING";CHR$(3)
980 LPRINT "PA12,43;LB=";CHR$(8);R;"(1/A)";CHR$(3)
990 LPRINT "PA12,36;LBHORIZONTAL DIRECTION";CHR$(3)
1000 LPRINT "PA12,29;LB=[";HAD;KAD;LAD;"]";CHR$(3)
1010 LPRINT "CP0,0.3;SIO.13,0.2;LB*";CHR$(3)
1020 LPRINT "SP0;"
1030 RETURN
1040 '
1050 *HOLZRING2 '** draw HOLZRING pattern **
1060 LPRINT "IN;DF;PS4;SP";SP;" "
1070 WINXY=R+6*DDA:WINXY=FIX(WINXY*1E+06)/1E+06
1080 SR=DDA/(2*WINXY)*50
1090   IF SR<1.3 THEN SR=1.3:WINXY=1.2*R
1100   IF SR>3 THEN SR=3:WINXY=R+4*DDA
1110 IF WINXY/DDA>200 THEN PLDA=FIX(WINXY*50)/10000! ELSE PLDA=DDA
1120 LPRINT "IP4000,860,10000,6860;IW;"
1130 LPRINT "SC";-WINXY;"",",",WINXY;"",",",-WINXY;"",",",WINXY;"",",",
1140 LPRINT "SR";.4*SR;"",",",SR;"",",",
1150 LPRINT "PU;PA0,0;CI";R;"",",",
1160 IF GREF$="n" OR GREF$="N" THEN 1230
1170 LPRINT "PU;PA";HGPRO;"",",",KGPRO;"",",",CI";PLDA;"",",",          G-disk
1180 LL=SQR(HGPRO^2+KGPRO^2)
1190 X=FIX(DDA*HGPRO/LL*1E+06)/1E+06:Y=FIX(DDA*KGPRO/LL*1E+06)/1E+06
1200 'LPRINT "PR";X;"",",",Y;"",",",DI";HGPRO;"",",",KGPRO;"",",",
1210 'LPRINT "CP1,-0.25;LB";HG;KG;LG;CHR$(3)
1220 LPRINT "DI;CP-0.5,-0.25;LBG";CHR$(3)

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1230 LPRINT "PU;PA";-HGPRO;","; -KGPRO;";CI";PLDA;";" ' O-disk
1240 'LPRINT "DI;CP-2.5,-0.25;LBO 0 0";CHR$(3)
1250 LPRINT "DI;CP-0.5,-0.25;LBO";CHR$(3)
1260 FOR J=1 TO 03-1
1270 H=HCA(J) : K=KCA(J) : L=LCA(J)
1280 IF DISK(J)=0 THEN 1410
1290 IF UU*UU+VV*VV<.0001 THEN 1330
1300 XI=FNPROX(FNXABC(H-HG/2,K-KG/2,L-LG/2),FNYABC(H-HG/2,K-KG/2,L-LG/2),FNZABC(H-HG/2,K-KG/2,L-LG/2))
1310 YI=FNPROY(FNXABC(H-HG/2,K-KG/2,L-LG/2),FNYABC(H-HG/2,K-KG/2,L-LG/2),FNZABC(H-HG/2,K-KG/2,L-LG/2))
1320 GOTO 1340
1330 XI=FNXABC(H-HG/2,K-KG/2,L-LG/2):YI=-FNYABC(H-HG/2,K-KG/2,L-LG/2)
1340 X=XI*CO+YI*SI:Y=XI*SI-YI*CO
1350 X=FIX(X*1E+06)/1E+06:Y=FIX(Y*1E+06)/1E+06
1360 LPRINT "PU;PA";X;",";Y;";CI";PLDA;";"
1370 LL=SQR(X*X+Y*Y)
1380 X=FIX(DDA*X/LL*1E+06)/1E+06:Y=FIX(DDA*Y/LL*1E+06)/1E+06
1390 LPRINT "PR";X;",";Y;";DI";X;",";Y;";"
1400 LPRINT "CP1,-0.25;LB";H;K;L;CHR$(3)
1410 NEXT J
1420 LPRINT "SPO;"
1430 RETURN
1440 '
1450 *INDEXING ' ** index on the K-M pattern **
1460 LPRINT "IW;"
1470 IF X=0 AND Y>0 THEN Q=3 : GOTO *SEP
1480 IF X=0 AND Y<0 THEN Q=2 : GOTO *SEP
1490 IF X>0 AND Y=0 THEN Q=4 : GOTO *SEP
1500 IF X<0 AND Y=0 THEN Q=1 : GOTO *SEP
1510 RAT=Y/X
1520 IF RAT>-1 AND RAT<0 AND X<0 THEN Q=1 : GOTO *SEP
1530 IF RAT<=-1 AND X<0 THEN Q=2 : GOTO *SEP
1540 IF RAT>=1 AND X>0 THEN Q=3 : GOTO *SEP
1550 IF RAT>0 AND RAT<1 AND X>0 THEN Q=1 : GOTO *SEP
1560 IF RAT>-1 AND RAT<0 AND X>0 THEN Q=4 : GOTO *SEP
1570 IF RAT<=-1 AND X>0 THEN Q=3 : GOTO *SEP
1580 IF RAT>=1 AND X<0 THEN Q=2 : GOTO *SEP
1590 IF RAT>0 AND RAT<1 AND X<0 THEN Q=4 : GOTO *SEP
1600 BEEP:RETURN
1610 *SEP
1620 GOSUB *SEP2
1630 DIX=FIX(100*COS(P*PAI#/2))/100:DIY=FIX(100*SIN(P*PAI#/2))/100
1640 LPRINT "DI";DIX;",";DIY;";"
1650 'LPRINT "DI";COS(P*PAI#/2);",";SIN(P*PAI#/2);";"
1660 ON P+1 GOTO 1670,1680,1690,1700
1670 LPRINT "PA";DDSC;",";WAI;";":GOTO 1710
1680 LPRINT "PA";EKS;",";DDSC;";":GOTO 1710
1690 LPRINT "PA";-DDSC;",";WAI;";":GOTO 1710
1700 LPRINT "PA";EKS;",";-DDSC;";"
1710 LPRINT "CPO.5,-0.25;LB";H;K;L;CHR$(3)
1720 RETURN
1730 *SEP2
1740 ON Q GOTO 1750,1790,1830,1870
1750 EKS=KXL:WAI=KYL ' Q=1
1760 IF ABS(WAI)<PLDD THEN GOTO 1780
1770 P=3:RETURN
1780 EKS=KXS:WAI=KYS:P=1:RETURN
1790 EKS=KXS:WAI=KYS ' Q=2
1800 IF ABS(EKS)<PLDD THEN GOTO 1820
1810 P=0:RETURN
1820 EKS=KXL:WAI=KYL:P=2:RETURN
1830 EKS=KXL:WAI=KYL ' Q=3
1840 IF ABS(EKS)<PLDD THEN GOTO 1860
1850 P=2:RETURN
1860 EKS=KXS:WAI=KYS:P=0:RETURN
1870 EKS=KXS:WAI=KYS ' Q=4
1880 IF ABS(WAI)<PLDD THEN GOTO 1900
1890 P=1:RETURN
1900 EKS=KXL:WAI=KYL:P=3:RETURN
1910 '
1920 *HOLZ
1930 LPRINT "IN;DF;PS4;PA;S10.12,0.25;SP";SP;";"
1940 LPRINT "IP4300,1400,9400,6500;"
1950 LPRINT "IW100,100,11000,7500;"
1960 LPRINT "SC";-DDSC;",";DDSC;",";DDSC;";"
1970 ANGRAN=SQR(2)*DD/R:SANG=ANGRAN/INTE
1980 LPRINT "PUO,0;CI";PLDDA;",";1;"
1990 FOR IJ=1 TO 03-1
2000 LPRINT "IW4300,1100,9900,6700;"
2010 IN=0:INA=0
2020 H=HCA(IJ):K=KCA(IJ):L=LCA(IJ)
2030 IF DISK(IJ)=0 THEN 2900
2040 IF UU*UU+VV*VV=.0001 THEN 2080

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2050 XI=FNPROX(FNXABC(H-HG/2,K-KG/2,L-LG/2),FNYABC(H-HG/2,K-KG/2,L-LG/2),FNZABC(H-HG/2,K-KG/2,L-LG/2))
2060 YI=FNPROY(FNXABC(H-HG/2,K-KG/2,L-LG/2),FNYABC(H-HG/2,K-KG/2,L-LG/2),FNZABC(H-HG/2,K-KG/2,L-LG/2))
2070 GOTO 2090
2080 XI=FNXABC(H-HG/2,K-KG/2,L-LG/2):YI=-FNYABC(H-HG/2,K-KG/2,L-LG/2)
2090 X=XI*CO+YI*SI:Y=XI*SI-YI*CO
2100 IF X=0 THEN 2150
2110 T=ATN(Y/X)*180/PAI#+90*(1-ABS(X)/X)
2120 ' T=T-360*(INT((T+360)/360)-1)
2130 T=T+360:T=T MOD 360
2140 P=INT((T+45)/90):P=P-4*INT(P/4):GOTO 2170
2150 IF Y>0 THEN T=90:P=1:GOTO 2170
2160 T=270:P=3
2170 FU1=R*R-(X+DD)*(X+DD):FU2=R*R-(X-DD)*(X-DD)
2180 FU3=R*R-(Y+DD)*(Y+DD):FU4=R*R-(Y-DD)*(Y-DD)
2190 ON P+1 GOTO 2200,2340,2480,2620
2200 ANGSL=-1
2210 IF FU3=>0 THEN GOTO 2240
2220 IF X=>0 THEN KXS=-2*DD:GOTO 2250
2230 IF X<0 THEN KXS=2*DD:GOTO 2250
2240 KXS=-X+SQR(FU3):KYS=DD
2250 IF FU4=>0 THEN GOTO 2280
2260 IF X=>0 THEN KXL=-2*DD:GOTO 2290
2270 IF X<0 THEN KXL=2*DD:GOTO 2290
2280 KXL=-X+SQR(FU4):KYL=-DD
2290 IF KXS>DD THEN KXS=DD :KYS=-Y-SQR(FU1)
2300 IF KXS<-DD THEN KXS=-DD:KYS=-Y+SQR(FU2)
2310 IF KXL>DD THEN KXL=DD :KYL=-Y+SQR(FU1)
2320 IF KXL<-DD THEN KXL=-DD:KYL=-Y-SQR(FU2)
2330 GOTO 2760
2340 ANGSL=1
2350 IF FU1=>0 THEN 2380
2360 IF Y=>0 THEN KYS=-2*DD:GOTO 2390
2370 IF Y<0 THEN KYS=2*DD:GOTO 2390
2380 KXS=DD:KYS=-Y+SQR(FU1)
2390 IF FU2=>0 THEN 2420
2400 IF Y=>0 THEN KYL=-2*DD:GOTO 2430
2410 IF Y<0 THEN KYL=2*DD:GOTO 2430
2420 KXL=-DD:KYL=-Y+SQR(FU2)
2430 IF KYS>DD THEN KXS=-X-SQR(FU3):KYS=DD
2440 IF KYS<-DD THEN KXS=-X+SQR(FU4):KYS=-DD
2450 IF KYL>DD THEN KXL=-X+SQR(FU3):KYL=DD
2460 IF KYL<-DD THEN KXL=-X-SQR(FU4):KYL=-DD
2470 GOTO 2760
2480 ANGSL=1
2490 IF FU3=>0 THEN 2520
2500 IF X=>0 THEN KXS=-2*DD:GOTO 2530
2510 IF X<0 THEN KXS=2*DD:GOTO 2530
2520 KXS=-X-SQR(FU3):KYS=DD
2530 IF FU4=>0 THEN 2560
2540 IF X=>0 THEN KXL=-2*DD:GOTO 2570
2550 IF X<0 THEN KXL=2*DD:GOTO 2570
2560 KXL=-X-SQR(FU4):KYL=-DD
2570 IF KXS>DD THEN KXS=DD :KYS=-Y+SQR(FU1)
2580 IF KXS<-DD THEN KXS=-DD:KYS=-Y-SQR(FU2)
2590 IF KXL>DD THEN KXL=DD :KYL=-Y-SQR(FU1)
2600 IF KXL<-DD THEN KXL=-DD:KYL=-Y+SQR(FU2)
2610 GOTO 2760
2620 ANGSL=-1
2630 IF FU1=>0 THEN 2660
2640 IF Y=>0 THEN KYS=-2*DD:GOTO 2670
2650 IF Y<0 THEN KYS=2*DD:GOTO 2670
2660 KXS=DD:KYS=-Y-SQR(FU1)
2670 IF FU2=>0 THEN 2700
2680 IF Y=>0 THEN KYL=-2*DD:GOTO 2710
2690 IF Y<0 THEN KYL=2*DD:GOTO 2710
2700 KXL=-DD:KYL=-Y-SQR(FU2)
2710 IF KYS>DD THEN KXS=-X+SQR(FU3):KYS=DD
2720 IF KYS<-DD THEN KXS=-X-SQR(FU4):KYS=-DD
2730 IF KYL>DD THEN KXL=-X-SQR(FU3):KYL=DD
2740 IF KYL<-DD THEN KXL=-X+SQR(FU4):KYL=-DD
2750 '
2760 KXS=FIX(KXS*1E+06)/10000!:KYS=FIX(KYS*1E+06)/10000!
2770 KXL=FIX(KXL*1E+06)/10000!:KYL=FIX(KYL*1E+06)/10000!
2780 LPRINT "PU;PA";KXS;"",KYS;"";"
2790 FOR ANG=-ANGRAN TO ANGRAN STEP SANG
2800 ANGLE=T*PAI#/180+ANG*ANGSL
2810 XPLOT=R*COS(ANGLE)-X:YPLOT=R*SIN(ANGLE)-Y
2820 IF ABS(XPLOT)>DD OR ABS(YPLOT)>DD THEN 2850
2830 XPLOT=INT(XPLOT*1E+06)/10000!:YPLOT=INT(YPLOT*1E+06)/10000!
2840 LPRINT "PD";XPLOT;"",YPLOT;"";"IN=1
2850 NEXT ANG
2860 IF IN=0 THEN 2900

```

```

2870 LPRINT "PD";KXL;",";KYL;";PU;"
2880 '
2890 GOSUB *INDEXING
2900 NEXT IJ
2910 LPRINT "SPO;"
2920 RETURN
2930 '
2940 *HOLZZ
2950 LPRINT "IN;DF;PS4;PA;SIO.12,0.25;SP";SP;";"
2960 LPRINT "IP4300,1400,9400,6500;"
2970 LPRINT "IW4300,1100,9900,6700;"
2980 LPRINT "SC";-DDSC;",";DDSC;",";-DDSC;",";DDSC;";"
2990 LPRINT "PUO,0;CI";PLDDA;",";1;"
3000 FOR I=0 TO 1
3010 IF I=OORG THEN GOTO 3480
3020 FOR IJ=1 TO O3-1
3030 LPRINT "IW4300,1100,9900,6700;"
3040 IF DISK(IJ)=I THEN GOTO 3460
3050 H=HCA(IJ):K=KCA(IJ):L=LCA(IJ)
3060 IF UU*UU+VV*VV<.0001 THEN 3100
3070 XI=FNPROX(FNXABC(H,K,L),FNYABC(H,K,L),FNZABC(H,K,L))
3080 YI=FNPROY(FNXABC(H,K,L),FNYABC(H,K,L),FNZABC(H,K,L))
3090 GOTO 3110
3100 XI=FNXABC(H,K,L):YI=-FNYABC(H,K,L)
3110 X=XI*CO+YI*SI:Y=XI*SI-YI*CO
3120 IF I=0 THEN 3140
3130 IF ABS(FNPRO(X,Y,0,HGPRO,KGPRO,0))<.0001 THEN 3460
3140 IN=0:INA=0:KXS=0:KYS=0:KXL=0:KYL=0
3150 GG=X*X+Y*Y+D*D
3160 GOSUB *BRAGGSL
3170 KXS=FIX(KXS*1E+06)/10000!:KYS=FIX(KYS*1E+06)/10000!
3180 KXL=FIX(KXL*1E+06)/10000!:KYL=FIX(KYL*1E+06)/10000!
3190 LPRINT "PU;PA";KXS;",";KYS;";"
3200 IF X=0 THEN 3220
3210 IF ABS(Y/X)<1 THEN 3290
3220 FOR II=0 TO INTE
3230 KX=-DD+2*II*DD/INTE+HGPRO*(-1)^I
3240 GOSUB *BRAGG1
3250 IF BR=0 THEN 3270
3260 GOSUB *PLOT
3270 NEXT II
3280 GOTO 3430
3290 FOR II=0 TO INTE
3300 KY=-DD+2*II*DD/INTE+KGPRO*(-1)^I
3310 GOSUB *BRAGG2
3320 IF BR=0 THEN 3340
3330 GOSUB *PLOT
3340 NEXT II
3350 GOTO 3430
3360 *PLOT
3370 KX=KX-HGPRO*(-1)^I:KY=KY-KGPRO*(-1)^I
3380 IF ABS(KX)>DD OR ABS(KY)>DD THEN IN=0 ELSE IN=1
3390 IF IN=0 THEN RETURN
3400 KX=FIX(KX*1E+06)/10000!:KY=FIX(KY*1E+06)/10000!
3410 LPRINT "PD";-KX;",";-KY;";":INA=1
3420 RETURN
3430 IF INA=0 THEN 3460
3440 LPRINT "PD";KXL;",";KYL;";PU;"
3450 GOSUB *INDEXING
3460 NEXT IJ
3470 IF GREF$="N" OR GREF$="n" THEN 3490
3480 NEXT I
3490 LPRINT "SPO;":RETURN
3500 '
3510 *BRAGG1
3520 AA=4*(Y*Y+D*D)
3530 BB=2*(2*KX*X*Y-GG*Y)
3540 CC=4*(X*X+D*D)*KX*KX-4*GG*X*KX+GG*GG-4*D*D*WN2
3550 DDD=BB*BB-AA*CC:BR=1:IF DDD<0 THEN BR=0 :GOTO 3570
3560 KY=(-BB-ABS(Y)/Y*SQR(DDD))/AA
3570 RETURN
3580 *BRAGG2
3590 AA=4*(X*X+D*D)
3600 BB=2*(2*KY*Y*X-GG*X)
3610 CC=4*(Y*Y+D*D)*KY*KY-4*GG*Y*KY+GG*GG-4*D*D*WN2
3620 DDD=BB*BB-AA*CC:BR=1:IF DDD<0 THEN BR=0 :GOTO 3640
3630 KX=(-BB-ABS(X)/X*SQR(DDD))/AA
3640 RETURN
3650 '
3660 *BRAGGSL
3670 FOR BSL=1 TO 2
3680 IF X=0 THEN 3700

```

```

3690 IF ABS(Y/X)<1 THEN 3860
3700 KX=DD*(-1)^BSL+HGPRO*(-1)^I
3710 GOSUB *BRAGG1
3720 KX=KX-HGPRO*(-1)^I:KY=KY-KGPRO*(-1)^I
3730 IF ABS(KY)>DD THEN IN=0 ELSE IN=1
3740 IF IN=1 THEN 3830
3750 FOR J=1 TO 2
3760 KY=DD*(-1)^J+KGPRO*(-1)^I
3770 GOSUB *BRAGG2
3780 KX=KX-HGPRO*(-1)^I:KY=KY-KGPRO*(-1)^I
3790 IF ABS(KX)>DD THEN IN=0 ELSE IN=1
3800 IF IN=1 THEN 3830
3810 NEXT J
3820 RETURN 3460
3830 ON BSL GOTO 3840,3850
3840 KXS=-KX:KYS=-KY:GOTO 4020
3850 KXL=-KX:KYL=-KY:GOTO 4020
3860 KY=DD*(-1)^BSL+KGPRO*(-1)^I
3870 GOSUB *BRAGG2
3880 KX=KX-HGPRO*(-1)^I:KY=KY-KGPRO*(-1)^I
3890 IF ABS(KX)>DD THEN IN=0 ELSE IN=1
3900 IF IN=1 THEN 3990
3910 FOR J=1 TO 2
3920 KX=DD*(-1)^J+HGPRO*(-1)^I
3930 GOSUB *BRAGG1
3940 KX=KX-HGPRO*(-1)^I:KY=KY-KGPRO*(-1)^I
3950 IF ABS(KY)>DD THEN IN=0 ELSE IN=1
3960 IF IN=1 THEN 3990
3970 NEXT J
3980 RETURN 3460
3990 ON BSL GOTO 4000,4010
4000 KXS=-KX:KYS=-KY:GOTO 4020
4010 KXL=-KX:KYL=-KY
4020 NEXT BSL
4030 RETURN

```

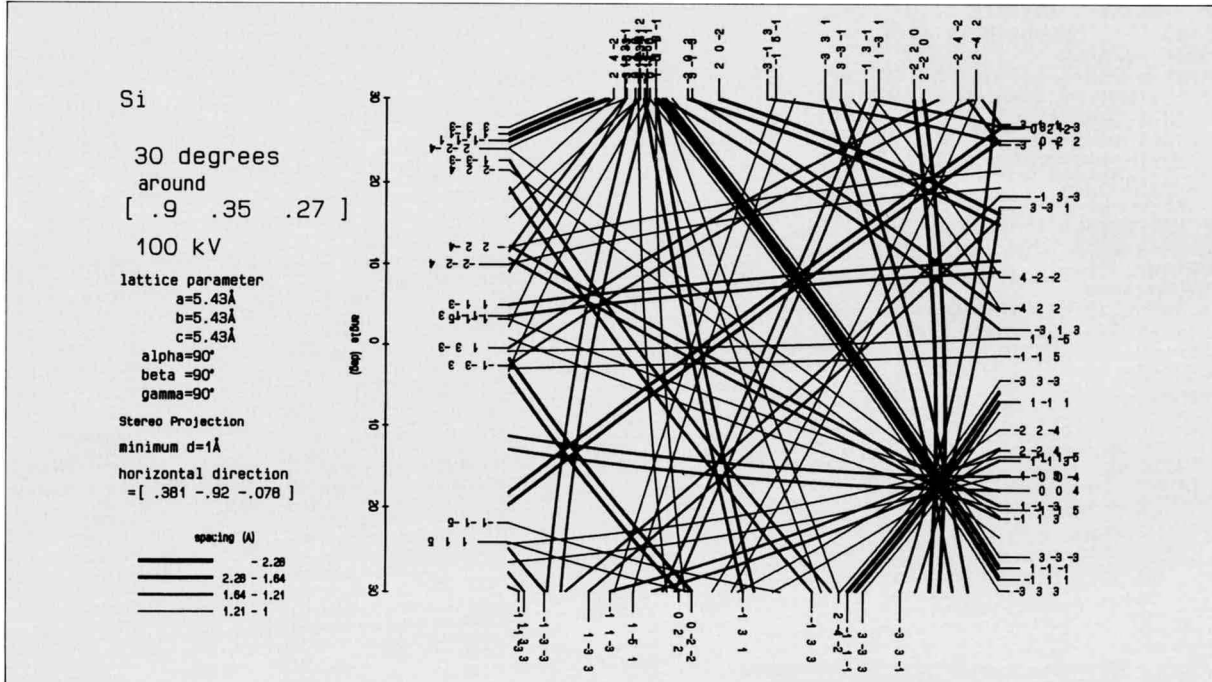
Language : N88BASIC (86) COMPILER
DOS : MS-DOS
Computer : NEC PC-9801
Printer : NEC PC-PR201
Plotter : ROLAND DXY-990

## Kikuchi-line program

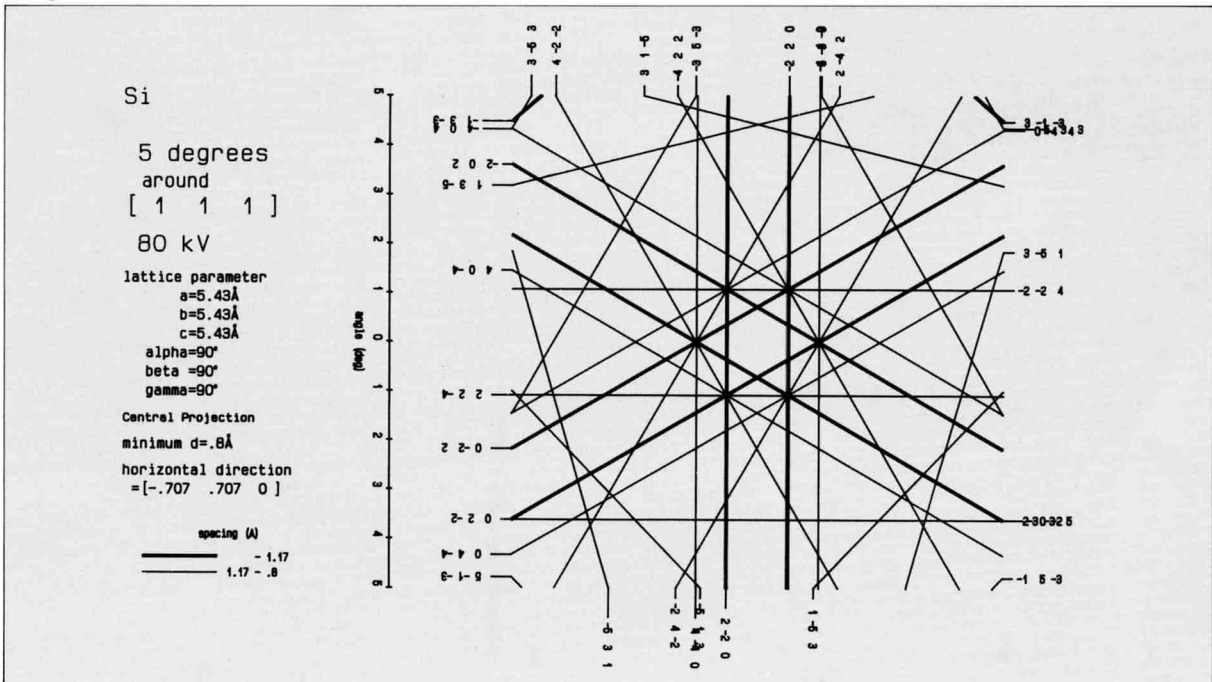
This program enables simulating Kikuchi-line maps for all the crystal systems and for an arbitrary orientation of a crystal. Simulated patterns are printed out to a printer or a plotter. The Kikuchi lines are drawn in four different widths or four different colors according to the spacings of lattice planes. This program has the following commands:

- 1) magnify/demagnify the angular range
- 2) rotate the pattern
- 3) shift the pattern
- 4) index/search the pole (zone axis)
- 5) index the Kikuchi line
- 6) calculate the angle between two poles (zone axes)

Output 1



Output 2



```

10 '*****
20 '***      ***
30 '***      KIKUCHI PATTERN ver.5      ***
40 '***      1988. 2.10 (Wed)      ***
50 '***      ***
60 '*****
70 '
80 DEFINT H-L,N
90 DIM HA(1000),KA(1000),LA(1000),IHKLS$(1500),RLA(1000)
100 DIM XPLS(1500),YPLS(1500),XPLE(1500),YPLE(1500)
110 DIM XPL(300),YPL(300),XPLL(300),YPLL(300),SYSS$(8),BRAV$(7)
120 DIM IG$(33),IGR$(33),IGR2$(33),IG2$(33),IG3$(33),IG4$(33)
130 CONSOLE ,,0,0:SCREEN 3,1:KEY ON:STOP ON:CLS 3:PI=3.14159
140 ON STOP GOSUB *STRP
150 GOSUB *FUNCTION
160 GOSUB *RDAT
170 GOSUB *INDAT
180 GOSUB *CONSTANT
190 GOSUB *KIKUCHI
200 GOSUB *COMMAND
210 END
220 ' ## DATA ##
230 DATA " cubic " ," hexagonal ,trigonal "
240 DATA " rhombohedral " ," tetragonal "
250 DATA " orthorhombic " ," monoclinic "
260 DATA " triclinic " ," < diamond type > "
270 DATA " primitive " ," body centered "
280 DATA " face centered " ," A-base centered "
290 DATA " B-base centered " ," C-base centered "
300 DATA " < diamond type > "
310 DATA 10,10,0,0,192,0,0,240,0,0,120,0,0,126,0,0,-32705,0,0,-16353
320 DATA 0,0,-32737,0,0,15,0,0,14,0,0,4,0,0
330 DATA 10,10,0,0,-16129,0,0,-16129,0,0,-16129,0,0,-16129,0,0,-16129,0,0
340 DATA -16129,0,0,-16129,0,0,-16129,0,0,-16129,0,0,-16129,0,0
350 DATA 10,10,0,0,8,0,0,28,0,0,60,0,0,126,0,0,254,0,0,127,0,0
360 DATA -32737,0,0,-32761,0,0,-16381,0,0,-16384,0,0
370 '
380 ' ## subroutines ##
390 '
400 *STRP
410 RETURN
420 *FUNCTION ' define user functions
430 DEF FNPRO(X1,Y1,Z1,X2,Y2,Z2)=X1*X2+Y1*Y2+Z1*Z2
440 DEF FNL(X,Y,Z)=X*X+Y*Y+Z*Z
450 DEF FNSCRPR(A,B,C,D,E,F)=(A*D+B*E+C*F)/SQRR((A*A+B*B+C*C)*(D*D+E*E+F*F))
460 DEF FNXCOD(U,V,W)=U*AX+V*BX+W*CX
470 DEF FNYCOD(U,V,W)=U*AY+V*BY+W*CY
480 DEF FNZCOD(U,V,W)=U*AZ+V*BZ+W*CZ
490 DEF FNXCICOD(U,V,W)=U*AIX+V*BIX+W*CIY
500 DEF FNYICOD(U,V,W)=U*AIY+V*BIY+W*CIY
510 DEF FNZICOD(U,V,W)=U*AIZ+V*BIZ+W*CIY
520 DEF FNXCODS(H,K,L)=H*AXS+K*BXS+L*CXS
530 DEF FNYCODS(H,K,L)=H*AYS+K*BYS+L*CYS
540 DEF FNZCODS(H,K,L)=H*AZS+K*BZS+L*CZS
550 DEF FNPROX(X,Y,Z)=(UU*WW*X+VV*WW*Y-FA1*FA1*Z)/(FA1*FA2)
560 DEF FNPROY(X,Y,Z)=(-VV*X+UU*Y)/FA1
570 DEF FNPROZ(X,Y,Z)=(UU*X+VV*Y+WW*Z)/FA2
580 DEF FNPROIX(X,Y,Z)=(UU*WW*X-FA2*VV*Y+FA1*UU*Z)/(FA1*FA2)
590 DEF FNPROIY(X,Y,Z)=(VV*WW*X+FA2*UU*Y+FA1*VV*Z)/(FA1*FA2)
600 DEF FNPROIZ(X,Y,Z)=(-FA1*X+WW*Z)/FA2
610 DEF FNEVOD(X)=X-2*INT(X/2)
620 RETURN
630 *REC.L
640 RL=(H*AXS+K*BXS+L*CXS)^2+(H*AYS+K*BYS+L*CYS)^2
650 RL=RL+(H*AZS+K*BZS+L*CZS)^2:RL=SQRR(RL)
660 RETURN
670 ' **** extinction rule ****
680 '   forbidden - - - AL=0 , allowed - - - AL=1
690 *P ' ** primitive
700   AL=1:RETURN
710 *I ' ** body center
720   AL=FNEVOD(H+K+L+1):RETURN
730 *F ' ** face center
740   AL1=FNEVOD(H+K+1):AL2=FNEVOD(K+L+1)
750   AL=INT((AL1+AL2)/2):RETURN
760 *A ' ** A-base center
770   AL=FNEVOD(K+L+1):RETURN
780 *B ' ** B-base center
790   AL=FNEVOD(L+H+1):RETURN
800 *C ' ** C-base center
810   AL=FNEVOD(H+K+1):RETURN
820 *D ' ** diamond

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830     AL1=FNEVOD(H+K+1):AL2=FNEVOD(K+L+1):AL=INT((AL1+AL2)/2)
840     IF AL=0 OR FNEVOD(H)=1 THEN RETURN
850     AL3=FNEVOD((H+K+L)/2+1):AL=INT((AL1+AL2+AL3)/3):RETURN
860 *R ' ** rhombohedral
870     AL=(-H+K+L+1)-3*INT((-H+K+L+1)/3):AL=FNEVEOD(AL):RETURN
880 '
890 *RDAT
900 FOR I=1 TO 8: READ SYSS(I):NEXT
910 FOR I=1 TO 7: READ BRAV$(I):NEXT
920 FOR I=0 TO 33: READ IGR$(I):NEXT
930 FOR I=0 TO 33: READ IGR2$(I):NEXT
940 FOR I=0 TO 33: READ IGR2$(I):NEXT
950 RETURN
960 *INDAT ' data input
970 GOSUB *DAT1: GOSUB *DAT2: GOSUB *DAT5: GOSUB *DAT6: GOSUB *DAT7
980 GOSUB *DAT8: GOSUB *DAT9: GOSUB *DAT10: GOSUB *DAT11
990 GOSUB *DAT12: GOSUB *DAT13: GOSUB *CONF.INDAT
1000 RETURN
1010 *DAT1
1020 PRINT " Specimen name "
1030 PRINT " (within 15 characters)";TAB(29);:INPUT S$
1040 S1$=S$:S$="":FOR I=1 TO 15:S$=S$+MID$(S1$,I,1):NEXT
1050 RETURN
1060 *DAT2
1070 PRINT " Crystal system"
1080 FOR I=1 TO 8:PRINT " ";SYSS(I);" - ";I:NEXT
1090 PRINT TAB(29);:INPUT SYS
1100 SYS=INT(ABS(SYS)):IF SYS=0 OR SYS>8 THEN 1090
1110 GOSUB *DAT3: GOSUB *DAT4
1120 RETURN
1130 *DAT3
1140 IF SYS=8 THEN BRAV=7:RETURN
1150 PRINT " Lattice type"
1160 FOR I=1 TO 6:PRINT " ";BRAV$(I);" - ";I:NEXT
1170 PRINT TAB(29);:INPUT BRAV
1180 BRAV=INT(ABS(BRAV)):IF BRAV=0 OR BRAV>6 THEN 1170
1190 RETURN
1200 *DAT4
1210 ON SYS GOSUB *SYS1,*SYS2,*SYS3,*SYS4,*SYS5,*SYS6,*SYS7,*SYS1
1220 A=ABS(A):B=ABS(B):C=ABS(C)
1230 IF A*B*C*ALP*BET*GAM=0 THEN 1210
1240 RETURN
1250 *DAT5
1260 PRINT " Accelerating voltage (kV)";TAB(29);:INPUT E
1270 IF E<=0 THEN 1260
1280 RETURN
1290 *DAT6
1300 PRINT " Zone axis u,v,w";TAB(29);:INPUT U,V,W
1310 IF FNL(U,V,W)=0 THEN 1300
1320 RETURN
1330 *DAT7
1340 PRINT " Horizontal direction u,v,w";TAB(29);:INPUT XO,YO,ZO
1350 IF FNL(XO,YO,ZO)=0 THEN 1340
1360 IF ABS(FNSCPR(U,V,W,XO,YO,ZO))>.9999 THEN 1340
1370 RETURN
1380 *DAT8
1390 PRINT " minimum limit of spacing (A)";TAB(29);:INPUT DMIN
1400 DMIN=ABS(DMIN):IF DMIN=0 THEN 1390
1410 RDMIN=1/DMIN:RETURN
1420 *DAT9
1430 PRINT " Projection"
1440 PRINT " central - - - - C or c"
1450 PRINT " stereo - - - - S or s"
1460 PRINT TAB(29);:INPUT PRJ$
1470 IF PRJ$="" THEN PRJ$="C"
1480 IF PRJ$="C" OR PRJ$="c" THEN PRJ=1 :GOTO 1510
1490 IF PRJ$="S" OR PRJ$="s" THEN PRJ=2 :GOTO 1510
1500 GOTO 1460
1510 PRINT " line - - L or l":PRINT " curve - C or c"
1520 PRINT TAB(29);:INPUT PRJLC$
1530 IF PRJLC$="" THEN PRJLC$="L"
1540 IF PRJLC$="L" OR PRJLC$="l" THEN PRJLC=1 :GOTO 1570
1550 IF PRJLC$="C" OR PRJLC$="c" THEN PRJLC=2 :GOTO 1570
1560 GOTO 1520
1570 IF PRJ=1 AND ANGRAN>60 THEN GOSUB *DAT10
1580 IF PRJ=2 AND ANGRAN>90 THEN GOSUB *DAT10
1590 RETURN
1600 *DAT10
1610 PRINT " Angular range ";
1620 IF PRJ=1 THEN PRINT "(max 60 deg)"; ELSE PRINT "(max 90 deg)";
1630 PRINT TAB(29);:INPUT ANGRAN
1640 ANGRAN=ABS(ANGRAN):IF ANGRAN<.01 THEN ANGRAN=10

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1650 IF PRJ=1 AND ANGRAN>60 THEN 1630
1660 IF PRJ=2 AND ANGRAN>90 THEN 1630
1670 RETURN
1680 *DAT11
1690 PRINT " Step number of lines (std. setting 10) ";TAB(29);:INPUT INTE
1700 INTE=INT(ABS(INTE))
1710 IF INTE<10 THEN INTE=10
1720 IF INTE>100 THEN INTE=100
1730 RETURN
1740 *DAT12
1750 PRINT " Output"
1760 PRINT " CRT - - - C":PRINT "          plotter - - P"
1770 PRINT TAB(29);:INPUT PRPL$
1780 IF PRPL$="" THEN PRPL$="C"
1790 IF PRPL$="C" OR PRPL$="c" THEN PRPL=1:GOTO 1820
1800 IF PRPL$="P" OR PRPL$="p" THEN PRPL=2:GOTO 1820
1810 GOTO 1770
1820 RETURN
1830 *DAT13
1840 PRINT " Grouping number of reflections";TAB(29);:INPUT NIL
1850 NIL=INT(ABS(NIL)):IF NIL>4 THEN 1840
1860 IF NIL=1 OR NIL=0 THEN NIL=1:RETURN
1870 PRINT "          by color - - c":PRINT "          by thickness - t"
1880 PRINT TAB(29);:INPUT COWI$
1890 IF COWI$="" THEN COWI$="C"
1900 IF COWI$="c" OR COWI$="C" THEN COWI=1:GOTO 1930
1910 IF COWI$="t" OR COWI$="T" THEN COWI=2:GOTO 1930
1920 GOTO 1880
1930 PRINT "          Boundary set"
1940 PRINT "          auto - - a":PRINT "          manual - m"
1950 PRINT TAB(29);:INPUT AUMANUS$
1960 IF AUMANUS$="" THEN AUMANUS$="A"
1970 IF AUMANUS$="A" OR AUMANUS$="a" THEN AUMANUS$="A":RETURN
1980 IF AUMANUS$="M" OR AUMANUS$="m" THEN AUMANUS$="M":GOTO 2000
1990 GOTO 1950
2000 * manual boundary set *
2010 PRINT TAB(11);"input boundary spacings (A)"
2020 FOR I=1 TO NIL-1
2030 PRINT TAB(19);I;"-->";I+1;:INPUT ":";BOUND(I):NEXT
2040 FOR I=1 TO NIL-1:FOR J=1 TO I:BOU=BOUND(I)
2050 IF BOUND(J)<BOU THEN BOUND(I)=BOUND(J):BOUND(J)=BOU
2060 NEXT:NEXT
2070 RETURN
2080 *SYS1 '          cubic <diamond>
2090 PRINT " Lattice constant";
2100 PRINT TAB(23);:INPUT "a (A) ";A:B=A:C=A
2110 ALP=PI/2:BET=ALP:GAM=ALP:ALPH=90:BETA=90:GAMM=90
2120 RETURN
2130 *SYS2 '          hexagonal ,trigonal
2140 PRINT " Lattice constant";
2150 PRINT TAB(23);:INPUT "a (A) ";A :B=A
2160 PRINT TAB(23);:INPUT "c (A) ";C
2170 ALP=PI/2:BET=ALP:GAM=2*PI/3:ALPH=90:BETA=90:GAMM=120
2180 RETURN
2190 *SYS3 '          rhombohedral
2200 PRINT "          rhombohedral coordinates -- 1"
2210 PRINT "          hexagonal coordinates ----- 2"
2220 PRINT TAB(33);:INPUT:RHOMB
2230 RHOMB=INT(ABS(RHOMB))
2240 IF RHOMB=0 OR RHOMB>2 THEN 2220
2250 IF RHOMB=2 THEN GOTO *SYS2
2260 PRINT " Lattice constant";
2270 PRINT TAB(23);:INPUT "a (A) ";A :B=A:C=A
2280 PRINT TAB(18);:INPUT "alpha (deg)";ALPH :BETA=ALPH:GAMM=ALPH
2290 ALP=ALPH*PI/180:BET=ALP:GAM=ALP
2300 RETURN
2310 *SYS4 '          tetragonal
2320 PRINT " Lattice constant";
2330 PRINT TAB(23);:INPUT "a (A) ";A :B=A
2340 PRINT TAB(23);:INPUT "c (A) ";C
2350 ALP=PI/2:BET=ALP:GAM=ALP:ALPH=90:BETA=90:GAMM=90
2360 RETURN
2370 *SYS5 '          orthorhombic
2380 PRINT " Lattice constant";
2390 PRINT TAB(23);:INPUT "a (A) ";A
2400 PRINT TAB(23);:INPUT "b (A) ";B
2410 PRINT TAB(23);:INPUT "c (A) ";C
2420 ALP=PI/2:BET=ALP:GAM=ALP:ALPH=90:BETA=90:GAMM=90
2430 RETURN
2440 *SYS6 '          monoclinic
2450 PRINT " Lattice constant";
2460 PRINT TAB(23);:INPUT "a (A) ";A

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2470 PRINT TAB(23);:INPUT "b (A) ";B
2480 PRINT TAB(23);:INPUT "c (A) ";C
2490 PRINT TAB(18);:INPUT "beta (deg)";BETA
2500 PRINT TAB(18);:INPUT "gamma (deg)";GAMM
2510 ALPH=90:ALP=ALPH*PI/180:BET=BETA*PI/180:GAM=GAMM*PI/180
2520 RETURN
2530 *SYS7 ' triclinic
2540 PRINT " Lattice constant"
2550 PRINT TAB(23);:INPUT "a (A) ";A
2560 PRINT TAB(23);:INPUT "b (A) ";B
2570 PRINT TAB(23);:INPUT "c (A) ";C
2580 PRINT TAB(18);:INPUT "alpha (deg)";ALPH
2590 PRINT TAB(18);:INPUT "beta (deg)";BETA
2600 PRINT TAB(18);:INPUT "gamma (deg)";GAMM
2610 ALP=ALPH*PI/180:BET=BETA*PI/180:GAM=GAMM*PI/180
2620 RETURN
2630 *CONF.INDAT
2640 CLS 3
2650 PRINT "1. Specimen name";TAB(37);S$
2660 PRINT "2. Crystal system";TAB(37);SYSS$(SYS)
2670 PRINT "3. Lattice type";TAB(37);BRAV$(BRAV)
2680 PRINT "4. Lattice constant";
2690 PRINT TAB(36);" a , b , c =";A;B;C;"(A)"
2700 PRINT TAB(25);" alpha , beta , gamma =";ALPH;BETA;GAMM;"(deg)"
2710 PRINT "5. Accelerating voltage";SPC(12);" E =";E;"(kV)"
2720 UP=FIX(U*1000)/1000:VP=FIX(V*1000)/1000:WP=FIX(W*1000)/1000
2730 PRINT "6. Zone axis";SPC(23);" [u,v,w] = [";UP;VP;WP;"]"
2740 X01=FIX(X0*1000)/1000:Y01=FIX(Y0*1000)/1000:Z01=FIX(Z0*1000)/1000
2750 PRINT "7. Horizontal direction [u,v,w] = [";X01;Y01;Z01;"]"
2760 PRINT "8. minimum limit of spacing ";DMIN;"(A)"
2770 PRINT "9. Projection ";TAB(36);
2780 IF PRJ=1 THEN PRINT " Central "; ELSE PRINT " Stereographic ";
2790 PRINT "projection";
2800 IF PRJLC=1 THEN PRINT "( line )" ELSE PRINT "( curve )"
2810 PRINT "10. Angular range ";TAB(36);FIX(ANGRAN*100)/100;"(deg)"
2820 PRINT "11. Step number of lines";TAB(36);INTE
2830 PRINT "12. Output";TAB(36);
2840 IF PRPL=1 THEN PRINT " CRT " ELSE PRINT " Plotter "
2850 PRINT "13. Grouping number of reflections";TAB(36);NIL
2860 IF NIL=1 THEN 2940
2870 PRINT TAB(37)
2880 IF COWI=1 THEN PRINT "color"; ELSE PRINT "thickness";
2890 PRINT " change ";
2900 IF AUMANUS="A" THEN PRINT " ( auto )":GOTO 2940
2910 PRINT:PRINT TAB(37);"< boundary >"
2920 FOR I=1 TO NIL-1
2930 PRINT TAB(35);I;"-->";I+1;";":BOUND(I):NEXT
2940 PRINT:PRINT " If some data must be altered, input number.";
2950 PRINT " Else enter 0 to start ."
2960 PRINT TAB(35);:INPUT WRONGDATAS$
2970 IF WRONGDATAS="" THEN 2960
2980 IF WRONGDATAS="E" OR WRONGDATAS="e" THEN END
2990 WRONGNUM=VAL(WRONGDATAS$)
3000 IF WRONGNUM=0 THEN GOTO 3070
3010 IF WRONGNUM>13 THEN 2960
3020 IF WRONGNUM>7 THEN 3050
3030 ON WRONGNUM GOSUB *DAT1,*DAT2,*DAT3,*DAT4,*DAT5,*DAT6,*DAT7
3040 GOTO 3060
3050 ON WRONGNUM-7 GOSUB *DAT8,*DAT9,*DAT10,*DAT11,*DAT12,*DAT13
3060 GOTO *CONF.INDAT
3070 CLS 1:RETURN
3080 *CHDATA
3090 GOSUB *CONF.INDAT: GOSUB *REC
3100 RETURN
3110 *AUTISTP
3120 AUMANUS="AL"
3130 DMAX=1/RLA(N):DSTEP=2*(DMAX-DMIN)/(NIL*(NIL+1))
3140 FOR I=1 TO NIL-1:BOUND(NIL-I)=DMIN+I*(I+1)/2*DSTEP:NEXT
3150 RETURN
3160 *REC
3170 RECAL=0
3180 IF SYS<>SYS1 THEN RECAL=1
3190 IF BRAV<>BRAV1 THEN RECAL=1
3200 IF A1<>A OR B1<>B OR C1<>C THEN RECAL=1
3210 IF ALPH1<>ALPH OR BETA1<>BETA OR GAMM1<>GAMM THEN RECAL=1
3220 IF E1<>E THEN RECAL=1
3230 IF DMIN1>DMIN THEN RECAL=1
3240 UU=FNXCOD(U,V,W):VV=FNXCOD(U,V,W):WW=FNZCOD(U,V,W)
3250 XA1=UU1:YA1=VV1:ZA1=WW1:XA2=UU:YA2=VV:ZA2=WW
3260 GOSUB *CALAN:ANG10=CANGL:IF ANGRAN1*1.05<ANG10+ANGRAN THEN RECAL=1
3270 RETURN
3280 *CALAN

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3290 RL1=XA1*XA1+YA1*YA1+ZA1*ZA1
3300 RL2=XA2*XA2+YA2*YA2+ZA2*ZA2
3310 COBR=FNPRO(XA1,YA1,ZA1,XA2,YA2,ZA2)
3320 COBR2=COBR*COBR/(RL1*RL2)
3330 IF ABS(COBR2)>.5 THEN 3350
3340 TAS=SQR(ABS(1/COBR2-1)):CANGL=ATN(TAS*SGN(COBR))*180/PI:GOTO 3380
3350 YZ=YA1*ZA2-ZA1*YA2:ZX=ZA1*XA2-XA1*ZA2:XY=XA1*YA2-YA1*XA2
3360 SIBR2=(YZ*YZ+ZX*ZX+XY*XY)/(RL1*RL2)
3370 TAS=SQR(ABS(SIBR2/(1-SIBR2))):CANGL=ATN(TAS*SGN(COBR))*180/PI
3380 CANGL=CANGL+360:CANGL=CANGL-180*INT(CANGL/180)
3390 IF SGN(COBR)=1 THEN 3400 ELSE IF CANGL=0 THEN CANGL=180
3400 RETURN
3410 *TEXTC
3420 LOCATE 3, 0:PRINT $$
3430 LOCATE 1, 1:PRINT FIX(ANGRAN*100)/100;"degrees"
3440 LOCATE 4, 2:PRINT "around"
3450 UP=FIX(U*1000)/1000:VP=FIX(V*1000)/1000:WP=FIX(W*1000)/1000
3460 LOCATE 1, 3:PRINT "[";UP;VP;WP;"]"
3470 LOCATE 2, 4:PRINT E;"kV"
3480 LOCATE 1, 5:PRINT "a =";A;"A"
3490 LOCATE 1, 6:PRINT "b =";B;"A"
3500 LOCATE 1, 7:PRINT "c =";C;"A"
3510 LOCATE 1, 8:PRINT "alpha =";ALPH;"deg"
3520 LOCATE 1, 9:PRINT "beta =";BETA;"deg"
3530 LOCATE 1,10:PRINT "gamma =";GAMM;"deg"
3540 LOCATE 0,11:IF PRJ=1 THEN PRINT "central"; ELSE PRINT "stereographic";
3550 PRINT " projection "
3560 LOCATE 0,12:PRINT "horizontal direction"
3570 X01=FIX(X0*1000)/1000:Y01=FIX(Y0*1000)/1000:Z01=FIX(Z0*1000)/1000
3580 LOCATE 1,13:PRINT "= [";X01;Y01;Z01;"]"
3590 LOCATE 1,14:PRINT "minimum d =";DMIN;"A"
3600 RETURN
3610 *WID
3620 IF NIL=1 THEN RETURN
3630 BOUND(NIL)=DMIN:BOU1$="spacing (A)":LBOU=LEN(BOU1$)
3640 IF PRPL=1 THEN 3680
3650 LPRINT "PU";-XYMAX*220;",";-XYMAX*80;";SIO.18,0 25;DI1,0;CP-3.0;";
3660 LPRINT "LB";BOU1$;CHR$(3);
3670 GOTO 3720
3680 WINDOW (0,0)-(639,399):VIEW (0,0)-(639,399)
3690 FOR J=1 TO LBOU
3700 MBOU$=MID$(BOU1$,J,1):MBOU=ASC(MBOU$)+256
3710 PUT (40+8*J,310),KANJI(MBOU):NEXT
3720 FOR I=NIL TO 1 STEP -1
3730 BOUN1$=STR$(BOUND(NIL-I)):BOUN2$=STR$(BOUND(NIL-I+1))
3740 IF BOUND(NIL-I)=0 THEN BOUN1$=" "
3750 IF BOUND(NIL-I+1)=0 THEN BOUN2$=" "
3760 BOU1$=" " : BOU2$=" "
3770 FOR J=1 TO 5
3780 BOU1$=BOU1$+MID$(BOUN1$,J,1):BOU2$=BOU2$+MID$(BOUN2$,J,1):NEXT
3790 SCL$=BOU1$+" "+BOU2$
3800 ON PRPL GOTO 3810,3930
3810 '* CRT *
3820 CL(0)=7:CL(1)=5:CL(2)=2:CL(3)=1:LSCL=LEN(SCL$):SST=(NIL-I)*20
3830 ON COWI GOTO 3840,3850
3840 LINE (10,330+SST)-(50,330+SST),CL(NIL-I):GOTO 3890
3850 IF NIL=2 AND I=2 THEN I2=3 ELSE I2=I
3860 FOR J=0 TO I2-1
3870 LINE (10,330+SST+J)-(50,330+SST+J)
3880 NEXT
3890 FOR J=1 TO LSCL
3900 MSCL$=MID$(SCL$,J,1):MSCL=ASC(MSCL$)+256
3910 PUT (50+8*J,326+SST),KANJI(MSCL)
3920 NEXT J :GOTO 4030
3930 '*plotter*
3940 WWXY=XYMAX/(6.5/2.4)
3950 IF NIL=2 AND I=2 THEN I2=3 ELSE I2=I
3960 FOR J=1 TO I2
3970 IF COWI=1 THEN LPRINT "SP";NIL-I2+1;";";
3980 XYME=- (XYMAX*87+WWXY*J)-XYMAX*7*(NIL-I)
3990 LPRINT "PU";-XYMAX*250;",";XYME;";PD";-XYMAX*220;",";XYME;";PU;";
4000 IF COWI=1 THEN GOTO 4020
4010 NEXT
4020 LPRINT "SIO.1,0.2;DI1,0;CP1,-0.25;LB";SCL$;CHR$(3);
4030 NEXT
4040 RETURN
4050 *TEXT
4060 LPRINT "IN;DF;SP1;IP0,0.4000,7200;IW;SCO,100,0,180"
4070 LPRINT "PU;PA10,160;SIO.26,0.4;LB";S$;CHR$(3)
4080 LPRINT "PA10,145;SIO.20,0.4;LB";FIX(ANGRAN*100)/100;"degrees";CHR$(3)
4090 LPRINT "PA15,138;SIO.20,0.35;LBaround";CHR$(3)
4100 UP=FIX(U*1000)/1000:VP=FIX(V*1000)/1000:WP=FIX(W*1000)/1000

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4110 LPRINT "PA10,131;SIO.20,0.4;LB[";UP;CHR$(9);VP;CHR$(9);WP;"]";CHR$(3)
4120 LPRINT "PA10,121;SIO.20,0.4;LB";E;"kV";CHR$(3)
4130 LPRINT "PA10,113;SIO.15,0.25;LB lattice parameter";CHR$(3)
4140 LPRINT "PA25,108;LBa=";CHR$(8);A;CHR$(8);CHR$(3);
4150 LPRINT "CS7;LB";CHR$(80);CHR$(3);"CS;"
4160 LPRINT "PA25,103;LBb=";CHR$(8);B;CHR$(8);CHR$(3);
4170 LPRINT "CS7;LB";CHR$(80);CHR$(3);"CS;"
4180 LPRINT "PA25,98;LBc=";CHR$(8);C;CHR$(8);CHR$(3);
4190 LPRINT "CS7;LB";CHR$(80);CHR$(3);"CS;"
4200 LPRINT "PA25,93;CP-4,0;LBalpha=";CHR$(8);ALPH;CHR$(8);CHR$(3);
4210 LPRINT "CS8;LB";CHR$(95);CHR$(3);"CS;"
4220 LPRINT "PA25,88;CP-4,0;LBbeta =" ;CHR$(8);BETA;CHR$(8);CHR$(3);
4230 LPRINT "CS8;LB";CHR$(95);CHR$(3);"CS;"
4240 LPRINT "PA25,83;CP-4,0;LBgamma=";CHR$(8);GAMM;CHR$(8);CHR$(3);
4250 LPRINT "CS8;LB";CHR$(95);CHR$(3);"CS;"
4260 LPRINT "PA10,76;SIO.13,0.2;";
4270 IF PRJ=1 THEN LPRINT "LBcentral "; ELSE LPRINT "LBstereo ";
4280 LPRINT "Projection ";CHR$(3)
4290 LPRINT "PA10,69;SIO.15,0.25;LBminimum d=";CHR$(8);DMIN;CHR$(8);CHR$(3);
4300 LPRINT "CS7;LB";CHR$(80);CHR$(3);"CS;"
4310 LPRINT "PA10,62;SIO.15,0.25;LBhorizontal direction";CHR$(3);
4320 X01=FIX(X0*1000)/1000;Y01=FIX(Y0*1000)/1000;Z01=FIX(Z0*1000)/1000
4330 LPRINT "PA10,57;SIO.12,0.25;LB =[";X01;Y01;Z01;"]";CHR$(3);
4340 LPRINT "SPO;"
4350 RETURN
4360 *CONSTANT ' calculate constants for calculation
4370 WN=SQR(1000*E*(1+9.788E-07*1000*E))/12.26 :WN2=WN*WN ' ** wave number
4380 COA=COS(ALP):COB=COS(BET):COG=COS(GAM)
4390 SIA=SIN(ALP):SIB=SIN(BET):SIG=SIN(GAM)
4400 DREA=SQR(1-COA*COA-COB*COB-COG*COG+2*COA*COB*COG):VOL=A*B*C*DREA
4410 AX=A:AY=0:AZ=0
4420 BX=B*COG:BY=DREA*B/SIB:BZ=B*(COA-COB*COG)/SIB
4430 CX=C*COB:CY=0:CZ=C*SIB
4440 AXS=1/A:AYS=(COA*COB-COG)/(A*DREA*SIB):AZS=-COB/(A*SIB)
4450 BXS=0:BYS=SIB/(B*DREA):BZS=0
4460 CYS=(COB*COG-COA)/(C*DREA*SIB):CXs=0:CZs=1/(C*SIB)
4470 ' above coordinates construct matrix
4480 ' AX BX CX AXS BXS CXS
4490 ' A = AY BY CY B = AYS BYS CYS
4500 ' AZ BZ CZ AZS BZS CZS
4510 D=AX*BY*CZ+AZ*BX*CY+CX*AY*BZ-(CX*BY*AZ+AX*CY*BZ+CZ*BX*AY)
4520 AIX=BY*CZ-BZ*CY : AIY=-AY*CZ+AZ*CY : AIZ=AY*BZ-AZ*BY
4530 BIX=-BX*CZ+BZ*CX : BIY=AX*CZ-AZ*CX : BIZ=-AX*BZ+AZ*BX
4540 CIX=BX*CY-BY*CX : CIY=-AX*CY+AY*CX : CIZ=AX*BY-AY*BX
4550 AIX=AIX/D : AIY=AIY/D : AIZ=AIZ/D
4560 BIX=BIX/D : BIY=BIY/D : BIZ=BIZ/D
4570 CIX=CIX/D : CIY=CIY/D : CIZ=CIZ/D
4580 ' above coordinates construct inversion matrix
4590 ' AIX BIX CIX
4600 ' INV(A) = AIY BIY CIY A*(INV(A)) = I
4610 ' AIZ BIZ CIZ
4620 UU=FNXCOD(U,V,W) ' ** [uu,vv,ww] represents
4630 VV=FNYCOD(U,V,W) ' incident beam direction
4640 WW=FNZCOD(U,V,W) ' in real space.
4650 FA1=SQR(UU*UU+VV*VV):FA2=SQR(UU*UU+VV*VV+WW*WW)
4660 MAXKX=WN*SIN(ANGRAN*PI/180) ' ** max. kx,ky
4670 MAXKZ=WN*COS(ANGRAN*PI/180) ' ** max. kz
4680 ON PRJ GOTO 4710,4730 ' ** angle at the corner
4690 ' ** ANGLEMAX(rad) is maximum angle at the corner.
4700 ' ** XYMAX is maximum value of x,y in graph
4710 ANGLEMAX=ATN(SQR(2)*TAN(ANGRAN*PI/180)) ' * for central proj.
4720 XYMAX=WN*TAN(ANGRAN*PI/180):GOTO 4750
4730 ANGLEMAX=2*ATN(SQR(2*(TAN(ANGRAN*PI/360))^2))' for stereographic proj.
4740 XYMAX=2*WN*TAN(ANGRAN*PI/360):GOTO 4750
4750 ZMAX=1.1*(WN-WN*COS(ANGLEMAX)) ' ** maximum z consider
4760 ANGSTEP=ANGRAN/INTE
4770 XPR=FNXCOD(X0,Y0,Z0):YPR=FNYCOD(X0,Y0,Z0):ZPR=FNZCOD(X0,Y0,Z0)
4780 GOSUB *PRJ :XHORI=XPR:YHORI=YPR
4790 CO=FNDCPR(1,0,0,XHORI,YHORI,0)
4800 SI=FNDCPR(0,1,0,XHORI,YHORI,0) '** CO and SI determine horiz. direction
4810 GOSUB *HORDIR
4820 RETURN
4830 *HORDIR
4840 XX=WN:YY=0:ZZ=0:X=1:Y=0:Z=0
4850 GOSUB *CALZONE2:X0=X3:Y0=Y3:Z0=Z3
4860 RETURN
4870 '
4880 *PRJ
4890 IF FA1<.001 THEN 4920
4900 XJ=FNPROX(XPR,YPR,ZPR):YJ=FNPROY(XPR,YPR,ZPR):ZJ=FNPROZ(XPR,YPR,ZPR)
4910 GOTO 4940
4920 IF SGN(WW)=1 THEN RETURN

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4930 XJ=-XPR:YJ=YPR:ZJ=-ZPR
4940 XPR=XJ:YPR=YJ:ZPR=ZJ: RETURN
4950 '
4960 *KIKUCHI
4970 SCREEN 3,1:CONSOLE 0,25:CLS 3:COLOR 2
4980 LOCATE 33,12:PRINT " calculating ":COLOR 0
4990 SYS1=SYS:BRAV1=BRAV
5000 A1=A:B1=B:C1=C:ALPH1=ALPH:BETA1=BETA:GAMM1=GAMM
5010 E1=E:U1=U:V1=V:W1=W:UU1=UU:VV1=VV:WW1=WW
5020 DMIN1=DMIN:ANGRAN1=ANGRAN:NIL1=NIL
5030 HJ=0:KJ=0:LJ=0:N=0
5040 GOSUB *CLIO
5050 IF ALCLI=0 THEN 5070
5060 LJ=LJ+1:GOTO 5040
5070 LJ=0:KJ=KJ+1:GOSUB *CLIL
5080 IF ALCLI=0 THEN 5100
5090 GOTO 5040
5100 LJ=0:KJ=0:HJ=HJ+1:GOSUB *CLILK
5110 IF ALCLI=0 THEN GOTO 5130
5120 GOTO 5040
5130 GOSUB *SORTING
5140 RETURN
5150 *CLIL
5160 ALCLI=0
5170 FOR LIJ=0 TO 2
5180 FOR HI=-1 TO 1 STEP 2
5190 FOR KI=-1 TO 1 STEP 2
5200 FOR LI=-1 TO 1 STEP 2
5210 H=HI*HJ:K=KI*KJ:L=LI*LIJ :GOSUB *REC.L
5220 IF RL<=RDMIN THEN ALCLI=1:RETURN
5230 NEXT:NEXT:NEXT:NEXT
5240 RETURN
5250 *CLILK
5260 ALCLI=0
5270 FOR LIJ=0 TO 1
5280 FOR KIJ=0 TO 2
5290 FOR HI=-1 TO 1 STEP 2
5300 FOR KI=-1 TO 1 STEP 2
5310 FOR LI=-1 TO 1 STEP 2
5320 H=HI*HJ:K=KI*KIJ:L=LI*LIJ :GOSUB *REC.L
5330 IF RL<=RDMIN THEN ALCLI=1:RETURN
5340 NEXT:NEXT:NEXT:NEXT:NEXT
5350 RETURN
5360 *CLIO
5370 ALCLI=0
5380 FOR HI=-1 TO 1 STEP 2
5390 IF HJ=0 AND HI=1 THEN 5480
5400 FOR KI=-1 TO 1 STEP 2
5410 IF KJ=0 AND KI=1 THEN 5470
5420 FOR LI=-1 TO 1 STEP 2
5430 IF LJ=0 AND LI=1 THEN 5460
5440 H=HI*HJ:K=KI*KJ:L=LI*LJ
5450 GOSUB *REC.L: IF RL<=RDMIN THEN ALCLI=1:GOSUB *KIKU
5460 NEXT
5470 NEXT
5480 NEXT
5490 RETURN
5500 *KIKU
5510 ON BRAV GOSUB *P,*I,*F,*A,*B,*C,*D,*R
5520 IF AL=0 THEN RETURN
5530 IF H*H+K*K+L*L=0 THEN RETURN
5540 XI=FNXCODS(H,K,L):YI=FNXCODS(H,K,L):ZI=FNZCODS(H,K,L)
5550 XPR=XI:YPR=YI:ZPR=ZI
5560 GOSUB *PRJ
5570 X=XPR:Y=YPR:Z=ZPR
5580 COPS=FNSCP(0,0,1,X,Y,Z):GG=XI*XI+YI*YI+ZI*ZI
5590 RY=SQR(WN2-GG/4) :RX=RY*COPS
5600 ANG=180:GOSUB *ELLIPSE:IF INAREA=0 THEN 5620 ' ** out of area
5610 GOSUB *CHIND: N=N+1:HA(N)=H:KA(N)=K:LA(N)=L:RLA(N)=RL:RETURN
5620 RETURN
5630 *CHIND
5640 FOR IJ=1 TO N
5650 IF H=HA(IJ) THEN 5670
5660 NEXT : RETURN
5670 IF K<>KA(IJ) THEN 5660
5680 IF L<>LA(IJ) THEN 5660
5690 RETURN 5620
5700 '
5710 *ELLIPSE ' ** reference ellipse --> reference circle --> projection
5720 ANGL=ANG*PI/180
5730 XX1=-RX*COS(ANGL):YY1=RY*SIN(ANGL) ' ** ref. ellipse
5740 RXY1=RY*RY-(XX1*XX1+YY1*YY1):IF RXY1<0 THEN RXY1=0

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5750         IF ANG=>90 AND ANG<=270 THEN 5770
5760     ZZ1=WN+SQR(RXY1):GOTO 5780
5770     ZZ1=WN-SQR(RXY1):GOTO 5780
5780     XXYY=X*X+Y*Y:IF XXYY=0 THEN GOTO 5830
5790     XX=(X*XX1-Y*YY1)/SQR(XXYY)+X/2
5800     YY=(X*YY1+Y*XX1)/SQR(XXYY)+Y/2
5810     ZZ=ZZ1+Z/2
5820     GOTO 5860
5830     XX=XX1+X/2
5840     YY=YY1+Y/2
5850     ZZ=ZZ1+Z/2 ' ** (XX,YY,ZZ) is on the ref. circle
5860     INAREA=1:IF ZZ>ZMAX THEN INAREA=0:RETURN
5870 ' *Projection
5880     ON PRJ GOTO 5890,5910
5890     XX=XX*WN/(WN-ZZ):YY=YY*WN/(WN-ZZ) ' *center
5900     RETURN
5910     XX=XX*2*WN/(2*WN-ZZ):YY=YY*2*WN/(2*WN-ZZ)' *stereo
5920 RETURN
5930 '
5940 *COMMAND
5950 IF PRPL=2 THEN GOSUB *PLOTWAIT
5960 GOSUB *PLOTING
5970 *COMIN
5980 ON STOP GOSUB *STRP
5990     ON KEY GOSUB *F1,*F2,*F3,*F4,*F5,*F6,*F7,*F8,*F9,*F10
6000     ON HELP GOSUB *HLP
6010     HLP=0:ST=1:KEY ON:HELP ON:GOSUB *HLP
6020     HFK$=INKEY$:GOTO 6020
6030 RETURN
6040 *FMEN
6050 FOR J=1 TO 10
6060     FUS=" f."+STR$(J)+" "
6070     FUS=MID$(FUS,1,3)+MID$(FUS,5,2)
6080     COLOR 4:PRINT FUS:PRINT
6090 NEXT J
6100 COLOR 0
6110     LOCATE 7,0 :PRINT ": change data "
6120     LOCATE 7,2 :PRINT ": magnify "
6130     LOCATE 7,4 :PRINT ": rotate "
6140     LOCATE 7,6 :PRINT ": shift "
6150     LOCATE 7,8 :PRINT ": pole indices "
6160     LOCATE 7,10:PRINT ": line indices "
6170     LOCATE 7,12:PRINT ": angle between ":PRINT " two poles "
6180     LOCATE 7,14:PRINT ": hard copy "
6190     LOCATE 7,16:PRINT ": plotter "
6200     LOCATE 7,18:PRINT ": end "
6210     LOCATE 0,20:COLOR 4:PRINT " Select function key "
6220     PRINT " type [HELP] ":PRINT " for input data "
6230 COLOR 0:RETURN
6240 *HLP
6250 COLOR 0:CLS 1:HLP=HLP+1:HLP=FNEVOD(HLP)
6260 IF HLP=0 THEN GOSUB *FMEN :RETURN
6270 GOSUB *TEXTC
6280 COLOR 4:PRINT:PRINT " Select function key "
6290     PRINT " type [HELP] "
6300     PRINT " for function menu "
6310 COLOR 0:RETURN
6320 *F1
6330     SCREEN 3,1:CLS 3:KEY OFF:HELP OFF
6340     GOSUB *CHDATA
6350     GOSUB *REC
6360     GOSUB *CONSTANT
6370     IF RECAL=1 THEN GOSUB *KIKUCHI
6380     GOSUB *PLOTING
6390 RETURN *COMIN
6400 *F2
6410     CLS 1:CONSOLE 1,24:LOCATE 1,0
6420 COLOR 0:PRINT " command ";:COLOR 4:PRINT " Magnify ":COLOR 0
6430     KEY OFF:HELP OFF
6440     GOSUB *MAG
6450     IF MAG$="R" OR MAG$="r" THEN 6500
6460     GOSUB *CONSTANT
6470     GOSUB *REC
6480     IF RECAL=1 THEN GOSUB *KIKUCHI
6490     GOSUB *PLOTING
6500 CONSOLE 0,24:CLS 1:RETURN *COMIN
6510 *F3
6520     CLS 1:CONSOLE 1,24:LOCATE 1,0
6530 COLOR 0:PRINT " command ";:COLOR 4:PRINT " Rotation ":COLOR 0
6540     KEY OFF:HELP OFF
6550     GOSUB *ROT
6560     IF RANG=0 THEN 6580

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6570 GOSUB *PLOTING
6580 CONSOLE 0,24:CLS 1:RETURN *COMIN
6590 *F4
6600 CLS 1:CONSOLE 1,24:LOCATE 1,0
6610 COLOR 0:PRINT " command ";;COLOR 4:PRINT " Shift ":COLOR 0
6620 KEY OFF:HELP OFF
6630 GOSUB *SHIFT
6640 IF TRANS="R" OR TRANS="r" THEN 6690
6650 GOSUB *CONSTANT
6660 GOSUB *REC
6670 IF RECAL=1 THEN GOSUB *KIKUCHI
6680 GOSUB *PLOTING
6690 CONSOLE 0,24:CLS 1:RETURN *COMIN
6700 *F5
6710 CLS 1:CONSOLE 1,24:LOCATE 1,0
6720 COLOR 0:PRINT " command ";;COLOR 4:PRINT " Pole ":COLOR 0
6730 HFK=5:KEY OFF:HELP OFF
6740 GOSUB *POLE
6750 CONSOLE 0,24:CLS 1:RETURN *COMIN
6760 *F6
6770 CLS 1:CONSOLE 1,24:LOCATE 1,0
6780 COLOR 0:PRINT " command ";;COLOR 4:PRINT " Reflection ":COLOR 0
6790 CLS 1:KEY OFF:HELP OFF
6800 GOSUB *REF
6810 CONSOLE 0,24:CLS 1:RETURN *COMIN
6820 *F7
6830 CLS 1:CONSOLE 1,24:LOCATE 1,0
6840 COLOR 0:PRINT " command ";;COLOR 4:PRINT " Angle ":COLOR 0
6850 HFK=7:CLS 1:KEY OFF:HELP OFF
6860 GOSUB *CA
6870 CONSOLE 0,24:CLS 1:RETURN *COMIN
6880 *F8
6890 CLS 1:KEY OFF:HELP OFF
6900 GOSUB *TEXTC
6910 COPY 3 : CLS 1
6920 RETURN *COMIN
6930 *F9
6940 KEY OFF:HELP OFF
6950 GOSUB *PLOTWAIT
6960 RETURN *COMIN
6970 *PLOTWAIT
6980 COLOR 0:CLS 1:PRINT " command ";;COLOR 4:PRINT " Plotter ":PRINT:COLOR 0
6990 COLOR 2:PRINT " * Set plotter *":COLOR 0:PRINT
7000 PRINT " Pen No. 1"
7010 IF NIL=1 OR COWI=2 THEN 7030
7020 PRINT " - No.;"NIL
7030 PRINT " will be used."
7040 IF COWI=2 THEN 7100
7050 PRINT:PRINT " recommendable color"
7060 PRINT " Pen 1 : Black":IF NIL=1 THEN 7100
7070 PRINT " Pen 2 : Brown":IF NIL=2 THEN 7100
7080 PRINT " Pen 3 : Blue ":IF NIL=3 THEN 7100
7090 PRINT " Pen 4 : Green"
7100 PRINT:PRINT " Pen speed ( cm/sec ) "
7110 INPUT " =";VS:VS=ABS(VS)
7120 IF VS=0 THEN 7100
7130 IF VS<1 THEN VS=1
7140 IF VS>127 THEN VS=127
7150 CLS 1:PRINT :PRINT " Hit any key to start ":PRINT
7160 PRINT " ( no indices [N] )"
7170 PRINT " ( cancel [C] )"
7180 HAK$=INKEY$:RMD=RND:IF HAK$="" THEN 7180
7190 IF HAK$="c" OR HAK$="C" THEN RETURN *COMIN
7200 PRPL=2:IF HAK$="n" OR HAK$="N" THEN NINDEX=1 ELSE NINDEX=0
7210 CLS 1:LOCATE 5,12:COLOR 2:PRINT "Plotting":COLOR 0
7220 GOSUB *PLOTING:PRPL=1
7230 RETURN
7240 *F10
7250 CLS 1:KEY OFF:HELP OFF
7260 PRINT "Are you sure":PRINT " to terminate":PRINT " this program ";
7270 INPUT "(y/n)";HFK$
7280 IF HFK$="Y" OR HFK$="y" THEN HFK$="E" ELSE HFK$=""
7290 IF HFK$="E" THEN SCREEN 3,1:CLS 3 :END
7300 CLS 1:RETURN *COMIN
7310 *MAG
7320 CLS 1:LOCATE 0,3
7330 COLOR 4:PRINT "1";
7340 COLOR 0:PRINT "change ":PRINT " angular range "
7350 COLOR 4:PRINT "2";
7360 COLOR 0:PRINT "center and angular ":PRINT " range by cursor "
7370 COLOR 4:PRINT "3";
7380 COLOR 0:PRINT "center by cursor and ":PRINT " input angular range "

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7390 COLOR 4:PRINT "4";
7400 COLOR 0:PRINT "input center and ":PRINT " angular range "
7410 COLOR 0:PRINT
7420 COLOR 4:PRINT "R";
7430 COLOR 0:PRINT "Return to ":PRINT " function menu"
7440 COLOR 0:INPUT " ";MAG$
7450 IF MAG$="R" OR MAG$="r" THEN RETURN
7460 MAG=VAL(MAG$) : MAG=INT(ABS(MAG))
7470 IF MAG=0 OR MAG>4 THEN 7440
7480 CLS 1:ON MAG GOSUB *RA,*CC,*CI,*II
7490 RETURN
7500 *RA
7510 LOCATE 0,3 : PRINT "present angular range "
7520 PRINT " =";ANGRAN;"deg."
7530 PRINT : PRINT "angular range (deg)"
7540 INPUT " =";ANGRANRA
7550 ANGRANRA=ABS(ANGRANRA)
7560 IF PRJ=1 AND ANGRANRA>60 THEN 7530
7570 IF PRJ=2 AND ANGRANRA>90 THEN 7530
7580 IF ANGRANRA<.01 THEN RETURN *MAG
7590 ANGRAN=ANGRANRA
7600 RETURN
7610 *CC
7620 XPO=0:YPO=0
7630 LOCATE 0,3:PRINT "determine center pole"
7640 GOSUB *POINTER
7650 IF A$="E" OR A$="e" THEN RETURN *MAG
7660 XM1=ZAXO:YM1=ZAYO:GOSUB *F257:XPO=XM1:YPO=YM1
7670 GOSUB *CALZONE:UC1=X3:VC1=Y3:WC1=Z3' ** zone axis at center
7680 CLS 1:LOCATE 0,3:PRINT "zone axis"
7690 PRINT " at the center is"
7700 PRINT " [";UZA;VZA;WZA;"]"
7710 PRINT : PRINT "determine angular range"
7720 PRINT " by cursor "
7730 GOSUB *POINTER:XM2=ZAXO:YM2=ZAYO ' ** another z.a. for angle range
7740 IF A$<>"E" AND A$<>"e" THEN GOTO 7760
7750 GOSUB *F257E:RETURN *MAG
7760 UUC=FNXCOD(UC1,VC1,WC1):VVC=FNXCOD(UC1,VC1,WC1):WVC=FNXCOD(UC1,VC1,WC1)
7770 ZAXO=XM2:ZAYO=YM2
7780 GOSUB *CALZONE
7790 UZA1=X3:VZA1=Y3:WZA1=Z3 ' ** zone axis on side-line of screen
7800 UUS=FNXCOD(X3,Y3,Z3):VVS=FNXCOD(X3,Y3,Z3):WVS=FNXCOD(X3,Y3,Z3)
7810 XA1=UUC:YA1=VVC:ZA1=WVC:XA2=UUS:YA2=VVS:ZA2=WVS
7820 GOSUB *CALAN :ANGRANRA=CANGL
7830 IF ANGRANRA>.01 THEN ANGRAN=ANGRANRA
7840 U=UC1:V=VC1:W=WC1
7850 RETURN
7860 *CI
7870 XPO=0:YPO=0
7880 LOCATE 0,3:PRINT "determine center pole"
7890 GOSUB *POINTER
7900 IF A$="E" OR A$="e" THEN RETURN *MAG
7910 XMO=ZAXO:YMO=ZAYO ' ** zone axis at centere
7920 GOSUB *CALZONE
7930 U=X3:V=Y3:W=Z3:UP=UZA:VP=VZA:WP=WZA
7940 CLS 1:LOCATE 0,3:PRINT "zone axis"
7950 PRINT " at the center is
7960 PRINT " [";UP;VP;WP;"]"
7970 PRINT : PRINT "determine angular range"
7980 INPUT " angle range (deg) =";ANGRANRA
7990 ANGRANRA=ABS(ANGRANRA)
8000 IF PRJ=1 AND ANGRANRA>60 THEN 7980
8010 IF PRJ=2 AND ANGRANRA>90 THEN 7980
8020 IF ANGRANRA<.01 THEN GOSUB *TYC:RETURN *MAG
8030 ANGRAN=ANGRANRA
8040 RETURN
8050 *II
8060 LOCATE 0,3
8070 PRINT " Zone axis u,v,w ":INPUT " ";UII,VII,WII
8080 IF UII^2+VII^2+WII^2=0 THEN RETURN *MAG
8090 PRINT " angular range (deg) ":INPUT " ";ANGRANRA
8100 ANGRANRA=ABS(ANGRANRA)
8110 IF PRJ=1 AND ANGRANRA>60 THEN 8090
8120 IF PRJ=2 AND ANGRANRA>90 THEN 8090
8130 IF ANGRANRA<.01 THEN RETURN *MAG
8140 U=UII:V=VII:W=WII:ANGRAN=ANGRANRA
8150 RETURN
8160 *ROT
8170 COLOR 0:LOCATE 0,3
8180 PRINT "rotation angle (deg)"
8190 INPUT " =";RANG:RANGL=RANG*PI/180
8200 CO1=CO*COS(RANGL)+SI*SIN(RANGL)

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8210     SI1=-CO*SIN(RANGL)+SI*COS(RANGL)
8220     CO=CO1:SI=SI1:GOSUB *HORDIR
8230     RETURN
8240     *SHIFT
8250     LOCATE 0,2:COLOR 4:PRINT "1";
8260     COLOR 0:PRINT "determine center":PRINT " by cursor "
8270     COLOR 4:PRINT "2";
8280     COLOR 0:PRINT "input x-angle ":PRINT " and y-angle "
8290     COLOR 0:PRINT:COLOR 4:PRINT "R";
8300     COLOR 0:PRINT "Return to ":PRINT " function menu"
8310     INPUT " ";TRANS$
8320     IF TRANS$="R" OR TRANS$="r" THEN RETURN
8330     TRAN=VAL(TRANS$):TRAN=INT(ABS(TRAN))
8340     IF TRAN=0 OR TRAN>2 THEN 8310
8350     ON TRAN GOTO *TRAN1,*TRAN2
8360     *TRAN1
8370         CLS 1:XPO=0:YPO=0
8380     LOCATE 0,3:PRINT "determine center pole"
8390     GOSUB *POINTER:XPO=ZAXO:YPO=ZAYO
8400     IF A$="E" OR A$="e" THEN TRANS$="E" : GOTO *SHIFT
8410     GOSUB *CALZONE:U=X3:V=Y3:W=Z3
8420     RETURN
8430     *TRAN2
8440     CLS 1 : LOCATE 0,2 : PRINT "input angle (deg)"
8450     INPUT " x-direction =";TRXO
8460     IF ABS(TRXO)>89 THEN GOTO 8450
8470     INPUT " y-direction =";TRYO
8480     IF ABS(TRYO)>89 THEN GOTO 8470
8490     IF TRXO=0 AND TRYO=0 THEN CLS 1:TRANS$="R": GOTO *SHIFT
8500     TRX=TRXO*PI/180:TRY=TRYO*PI/180
8510     STRX=SIN(TRX):STRY=SIN(TRY)
8520     STR2=SQR(1-STRX*STRX*STRY*STRY)
8530     XX=WN*STRX*SQR(1-STRY*STRY)/STR2
8540     YY=WN*STRY*SQR(1-STRX*STRX)/STR2
8550     ZZ=SQR(WN2-(XX*XX+YY*YY))
8560     GOSUB *CALZONE2:U=X3:V=Y3:W=Z3
8570     RETURN
8580     *POLE
8590     LOCATE 0,3
8600     COLOR 4:PRINT "1";
8610     COLOR 0:PRINT "index the pole ":PRINT
8620     COLOR 4:PRINT "2";
8630     COLOR 0:PRINT "search the pole ":PRINT
8640     COLOR 4:PRINT "3";
8650     COLOR 0:PRINT "calculate the angle "
8660     PRINT " between two poles ":PRINT
8670     COLOR 4:PRINT "R";
8680     COLOR 0:PRINT "Return to ":PRINT " function menu"
8690     COLOR 0:INPUT " ";POS$
8700     IF POS$="R" OR POS$="r" THEN RETURN
8710     PO=VAL(POS$):PO=INT(ABS(PO)):IF PO=0 OR PO>4 THEN 8690
8720     CLS 1: ON PO GOSUB *SI,*FP,*CA
8730     CLS 1:GOTO *POLE
8740     *SI
8750     XPO=0:YPO=0
8760     GOSUB *POINTER
8770         XPO=ZAXO:YPO=ZAYO
8780     IF A$="E" THEN RETURN
8790     GOSUB *CALZONE
8800     LOCATE 1,5:PRINT "pole : "
8810     PRINT " [{";UZA;VZA;WZA;"}] "
8820     GOSUB *TYC:GOTO 8760
8830     *FP
8840     CLS 1:LOCATE 0,12:PRINT " for END ":PRINT " input 0,0,0"
8850     LOCATE 0,3 : PRINT "input index"
8860     INPUT " U,V,W =";UX,VX,WX
8870     IF UX^2+VX^2+WX^2 =0 THEN :RETURN
8880     GET (XP,YP)-STEP(9,9),IG2%
8890     GOSUB *TYC
8900     XPR=FNXCOD(UX,VX,WX):YPR=FNXCOD(UX,VX,WX):ZPR=FNXCOD(UX,VX,WX)
8910     SLEN=SQR(XPR*XPR+YPR*YPR+ZPR*ZPR)
8920     GOSUB *PRJ :X=XPR:Y=YPR:Z=ZPR
8930     X1=(CO*X+SI*Y)*WN/SLEN : Y1=(-SI*X+CO*Y)*WN/SLEN : Z1=Z*WN/SLEN
8940     X1=-X1 : Y1=Y1 : Z1=WN-Z1
8950     ON PRJ GOTO 8960,8980
8960     X2=X1*WN/(WN-Z1):Y2=Y1*WN/(WN-Z1) ' ** central
8970     GOTO 8990
8980     X2=X1*2*WN/(2*WN-Z1):Y2=Y1*2*WN/(2*WN-Z1) ' ** stereo
8990     IF ABS(X2)<=XYMAX AND ABS(Y2)<=XYMAX THEN CLS 1:GOTO 9040
9000     LOCATE 0,6:COLOR 2:PRINT " out of area ":COLOR 0
9010     LOCATE 0,8 :PRINT " HIT RETURN KEY"
9020     HIR$=INKEY$:IF HIR$="" THEN 9020

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9030 GOTO *FP
9040 XP=MAP(X2,0):YP=MAP(Y2,1)
9050 GET (XP,YP)-STEP(9,9),IG2%:PUT (XP,YP),IG%,OR
9060 LOCATE 0,6:PRINT " Zone axis "
9070 PRINT " [";UX;VX;WX;"]":PRINT " is indicated."
9080 LOCATE 0,10 :PRINT " HIT RETURN KEY"
9090 HIR$=INKEY$:IF HIR$="" THEN 9090
9100 PUT (XP,YP),IG2%,AND:GOTO *FP
9110 RETURN
9120 *CA
9130 LOCATE 0,3
9140 PRINT:COLOR 4:PRINT "1";:COLOR 0:PRINT "two poles by cursor "
9150 PRINT:COLOR 4:PRINT "2";:COLOR 0:PRINT "one pole by cursor "
9160 PRINT " onother by index "
9170 COLOR 4:PRINT "3";:COLOR 0:PRINT "two poles by indices "
9180 PRINT:PRINT:COLOR 4:PRINT "R";:COLOR 0:PRINT "Return to "
9190 PRINT " function menu ":INPUT " ";CA3$
9200 IF CA3$="R" OR CA3$="r" THEN RETURN
9210 CA3=VAL(CA3$):CA3=INT(ABS(CA3))
9220 IF CA3=0 OR CA3>4 THEN 9190
9230 ON CA3 GOTO *TPC,*OC01,*TPI
9240 *TPC
9250 CLS 1:XPO=0:YPO=0
9260 GOSUB *POINTER
9270 IF A$="E" THEN RETURN
9280 GOSUB *F257:XPO=ZAXO:YPO=ZAYO
9290 GOSUB *CALZONE:UZA1=UZA:VZA1=VZA:WZA1=WZA
9300 XX1=XX:YY1=YY:ZZ1=ZZ
9310 GOSUB *POINTER
9320 IF A$="E" THEN GOSUB *F257E:RETURN
9330 XPO=ZAXO:YPO=ZAYO
9340 GOSUB *CALZONE:UZA2=UZA:VZA2=VZA:WZA2=WZA
9350 XX2=XX:YY2=YY:ZZ2=ZZ
9360 XA1=XX1:YA1=YY1:ZA1=ZZ1:XA2=XX2:YA2=YY2:ZA2=ZZ2
9370 GOSUB *CALAN : ANG=CANGL:ANG=FIX(ANG*100)/100
9380 CLS 1:LOCATE 0,5:PRINT " angle between "
9390 PRINT " [";UZA1;VZA1;WZA1;"]"
9400 PRINT " and":PRINT " [";UZA2;VZA2;WZA2;"]"
9410 PRINT " is ";ANG;"degrees"
9420 PRINT:PRINT " Hit return key"
9430 A$=INKEY$ : IF A$="" THEN 9430
9440 GOSUB *TYC:GOSUB *F257E:CLS 1:GOTO 9260
9450 *OC01
9460 CLS 1:XPO=0:YPO=0
9470 GOSUB *POINTER
9480 IF A$="E" THEN RETURN
9490 XPO=ZAXO:YPO=ZAYO :GOSUB *CALZONE :XX1=XX:YY1=YY:ZZ1=ZZ
9500 UZA1=UZA:VZA1=VZA:WZA1=WZA
9510 CLS 1:LOCATE 0,5:PRINT "arrowed pole is"
9520 PRINT " [";UZA;VZA;WZA;"]"
9530 LOCATE 0,8:PRINT "another pole "
9540 INPUT " u,v,w =";UX,VX,WX
9550 IF UX^2+VX^2+WX^2=0 THEN GOSUB *TYC:RETURN
9560 XPR=FNXCOD(UX,VX,WX):YPR=FNYCOD(UX,VX,WX):ZPR=FNZCOD(UX,VX,WX)
9570 SLEN=SQR(XPR*XPR+YPR*YPR+ZPR*ZPR)
9580 GOSUB *PRJ :X=XPR:Y=YPR:Z=ZPR
9590 XX2=CO*X+SI*Y : YY2=-SI*X+CO*Y : ZZ2=Z
9600 XA1=XX1:YA1=YY1:ZA1=ZZ1:XA2=XX2:YA2=YY2:ZA2=ZZ2
9610 GOSUB *CALAN :ANG=CANGL:ANG=FIX(ANG*100)/100
9620 CLS 1:LOCATE 0,5:PRINT " angle between "
9630 PRINT " [";UZA1;VZA1;WZA1;"]"
9640 PRINT " and [";UX;VX;WX;"]"
9650 PRINT " is ";ANG;"degrees"
9660 PRINT:PRINT " Hit return key"
9670 A$=INKEY$ : IF A$="" THEN 9670
9680 GOSUB *TYC:CLS 1:GOTO 9470
9690 *TPI
9700 CLS 1:LOCATE 0,15:PRINT " for END ":PRINT " input 0,0,0"
9710 LOCATE 0,5:PRINT " one pole "
9720 INPUT " u,v,w =";UX1,VX1,WX1
9730 IF UX1^2+VX1^2+WX1^2=0 THEN RETURN
9740 XPR=FNXCOD(UX1,VX1,WX1):YPR=FNYCOD(UX1,VX1,WX1):ZPR=FNZCOD(UX1,VX1,WX1)
9750 GOSUB *PRJ :XA1=XPR:YA1=YPR:ZA1=ZPR
9760 LOCATE 0,8:PRINT " another pole "
9770 INPUT " u,v,w =";UX2,VX2,WX2
9780 IF UX2^2+VX2^2+WX2^2=0 THEN RETURN
9790 XPR=FNXCOD(UX2,VX2,WX2):YPR=FNYCOD(UX2,VX2,WX2):ZPR=FNZCOD(UX2,VX2,WX2)
9800 GOSUB *PRJ :XA2=XPR:YA2=YPR:ZA2=ZPR
9810 GOSUB *CALAN : ANG=CANGL:ANG=FIX(ANG*100)/100
9820 CLS 1:LOCATE 0,5:PRINT " angle between "
9830 PRINT " [";UX1;VX1;WX1;"]"
9840 PRINT " and [";UX2;VX2;WX2;"]"

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9850 PRINT " is ";ANG;"degrees"
9860 PRINT:PRINT "HIT RETURN KEY"
9870 A$=INKEY$:IF A$="" THEN 9870
9880 CLS 1:GOTO *TPI
9890 RETURN
9900 *REF
9910 GOSUB *MENUR
9920 XR=195:YR=195
9930 GET (XR,YR)-STEP(9,9),IG2%
9940 AREF$=INKEY$:AREF=VAL(AREF$)
9950 IF AREF$="" THEN 9940
9960 IF AREF$=" " THEN GOSUB *REFSEARCH:GOSUB *MENUR:GOTO 9940
9970 IF AREF=5 THEN 9940
9980 ON AREF GOSUB *TY1R,*TY2R,*TY3R,*TY4R,,*TY6R,*TY7R,*TY8R,*TY9R
9990 IF AREF$="E" OR AREF$="e" THEN GOSUB *TYER:RETURN
10000 GOTO 9940
10010 *MENUR
10020 CLS 1 : LOCATE 0,3 : PRINT " Push ten key"
10030 LOCATE 0,10
10040 PRINT " space : get "
10050 PRINT
10060 PRINT " E : end "
10070 PRINT
10080 PRINT "ten key : cursor control"
10090 RETURN
10100 *TY2R
10110 IF YR=390 THEN RETURN
10120 PUT (XR,YR),IG2%,AND
10130 IF XR=0 THEN YR=YR+5:GOTO 10160
10140 IF YR=390 THEN YR=YR+5:GOTO 10160
10150 YR=390
10160 GET (XR,YR)-STEP(9,9),IG2%:PUT (XR,YR),IGR%,OR
10170 RETURN
10180 *TY4R
10190 IF XR=0 THEN RETURN
10200 PUT (XR,YR),IG2%,AND:IF YR=0 THEN XR=XR-5:GOTO 10230
10210 IF YR=390 THEN XR=XR-5:GOTO 10230
10220 XR=0
10230 GET (XR,YR)-STEP(9,9),IG2%:PUT (XR,YR),IGR%,OR
10240 RETURN
10250 *TY6R
10260 IF XR=390 THEN RETURN
10270 PUT (XR,YR),IG2%,AND:IF YR=0 THEN XR=XR+5:GOTO 10300
10280 IF YR=390 THEN XR=XR+5:GOTO 10300
10290 XR=390
10300 GET (XR,YR)-STEP(9,9),IG2%:PUT (XR,YR),IGR%,OR
10310 RETURN
10320 *TY8R
10330 IF YR=0 THEN RETURN
10340 PUT (XR,YR),IG2%,AND:IF XR=0 THEN YR=YR-5:GOTO 10370
10350 IF XR=390 THEN YR=YR-5:GOTO 10370
10360 YR=0
10370 GET (XR,YR)-STEP(9,9),IG2%:PUT (XR,YR),IGR%,OR
10380 RETURN
10390 *TY1R
10400 PUT (XR,YR),IG2%,AND :XR=0:YR=390
10410 GET (XR,YR)-STEP(9,9),IG2%:PUT (XR,YR),IGR%,OR
10420 RETURN
10430 *TY3R
10440 PUT (XR,YR),IG2%,AND :XR=390:YR=390
10450 GET (XR,YR)-STEP(9,9),IG2%:PUT (XR,YR),IGR%,OR
10460 RETURN
10470 *TY7R
10480 PUT (XR,YR),IG2%,AND :XR=0:YR=0
10490 GET (XR,YR)-STEP(9,9),IG2%:PUT (XR,YR),IGR%,OR
10500 RETURN
10510 *TY9R
10520 PUT (XR,YR),IG2%,AND :XR=390:YR=0
10530 GET (XR,YR)-STEP(9,9),IG2%:PUT (XR,YR),IGR%,OR
10540 RETURN
10550 *TYER
10560 PUT (XR,YR),IG2%,AND
10570 RETURN
10580 *REFSEARCH
10590 IF XR=0 THEN CASE=1:GOTO 10640
10600 IF XR=390 THEN CASE=2:GOTO 10640
10610 IF YR=0 THEN CASE=3:GOTO 10640
10620 IF YR=390 THEN CASE=4:GOTO 10640
10630 RETURN
10640 ON CASE GOTO 10650,10680,10710,10740
10650 SYR1=-MAP(YR+9,3):SYR2=-MAP(YR,3)
10660 SXR1=-XYMAX*1.01:SXR2=-XYMAX*.99

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10670 GOTO 10770
10680     SYR1=-MAP(YR+9,3):SYR2=-MAP(YR,3)
10690     SXR1=XYMAX*.99:SXR2=XYMAX*1.01
10700 GOTO 10770
10710     SXR1=MAP(XR,2):SXR2=MAP(XR+9,2)
10720     SYR1=XYMAX*.99:SYR2=XYMAX*1.01
10730 GOTO 10770
10740     SXR1=MAP(XR,2):SXR2=MAP(XR+9,2)
10750     SYR1=-XYMAX*1.01:SYR2=-XYMAX*.99
10760 GOTO 10770
10770 FOR JSER=1 TO NSER
10780     XPS=XPLS(JSER):YPS=YPLS(JSER)
10790     XPE=XPLE(JSER):YPE=YPLE(JSER)
10800     IF XPS<=SXR1 OR XPS=>SXR2 THEN 10840
10810     IF YPS<=SYR1 OR YPS=>SYR2 THEN 10840
10820 GOSUB *SHREF1
10830     IF A$="e" OR A$="E" THEN RETURN
10840     IF XPE<=SXR1 OR XPE=>SXR2 THEN 10880
10850     IF YPE<=SYR1 OR YPE=>SYR2 THEN 10880
10860 GOSUB *SHREF2
10870     IF A$="e" OR A$="E" THEN RETURN
10880 NEXT JSER
10890 RETURN
10900 *SHREF1
10910     XR1=XPE:YR1=YPE:GOTO 10940
10920 *SHREF2
10930     XR1=XPS:YR1=YPS:GOTO 10940
10940     XRO=MAP(XR1,0):YRO=MAP(-YR1,1)
10950     IF XRO<11 OR YRO<11 THEN 10980
10960 GET (XRO,YRO)-STEP(9,9),IG3%:PUT (XRO,YRO),IG%,OR
10970 GOTO 10990
10980 GET (XRO-10,YRO-10)-STEP(9,9),IG3%:PUT (XRO-10,YRO-10),IGR2%,OR
10990 CLS 1:LOCATE 0,3:PRINT " index "
11000 PRINT " h,k,l =":IHKL$(JSER)
11010 PRINT:PRINT "Hit space key":PRINT " for next index"
11020 PRINT:PRINT "Hit key [E]":PRINT " for end "
11030 A$=INKEY$ : IF A$="" THEN GOTO 11030
11040 IF A$=" " THEN 11070
11050 IF A$="e" OR A$="E" THEN 11070
11060 GOTO 11030
11070 IF XRO<11 OR YRO<11 THEN 11100
11080 PUT (XRO,YRO),IG3%,AND
11090 GOTO 11110
11100 PUT (XRO-10,YRO-10),IG3%,AND
11110 RETURN
11120 *SORTING
11130 FOR I=1 TO N
11140     FOR J=1 TO I
11150         RRR=RLA(J):HH=HA(J):KK=KA(J):LL=LA(J)
11160         IF RLA(J)=>RLA(I) THEN 11190
11170         RLA(J)=RLA(I):HA(J)=HA(I):KA(J)=KA(I):LA(J)=LA(I)
11180         RLA(I)=RRR:HA(I)=HH:KA(I)=KK:LA(I)=LL
11190     NEXT
11200 NEXT
11210 RETURN
11220 *STRP2
11230 RETURN *STRP1
11240 *PLOTING
11250     IF AUMANUS$="M" THEN 11270
11260 GOSUB *AUTISTP
11270 NSER=0
11280 ON STOP GOSUB *STRP2
11290 STOP ON
11300 ON PRPL GOTO 11310 , 11370
11310 ' ** C R T **
11320     CONSOLE , ,0,0 : SCREEN 3,1 : CLS 3
11330     XYMX=1.05263*XYMAX
11340     WINDOW (-XYMX,-XYMX)-(XYMX,XYMX)
11350     VIEW (210,0)-(609,399)
11360 GOTO 11470
11370 ' ** plotter **
11380     SCXY=FIX(XYMAX*1E+06)/10000
11390     ORGX=7100:ORGY=3900:IPXY=2600
11400     IPXMIN=4300:IPXMAX=9900:IPYMIN=1100:IPYMAX=6700
11410     IPXMIN=ORGX-IPXY:IPXMAX=ORGX+IPXY
11420     IPYMIN=ORGY-IPXY:IPYMAX=ORGY+IPXY
11430 LPRINT "IN;DF;PS4;PA;SIO.1,0.2;SP1;VS";VS;" "
11440 LPRINT "IP";IPXMIN;" ";IPYMIN;" ";IPXMAX;" ";IPYMAX;" "
11450 LPRINT "IW";IPXMIN;" ";IPYMIN;" ";IPXMAX;" ";IPYMAX;" "
11460 LPRINT "SC";-SCXY;" ";-SCXY;" ";-SCXY;" ";-SCXY;" "
11470 ' ** CURVE OR LINE
11480 ON PRJLC GOTO *AP.LINE , *CURVE

```

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11490 '
11500 *AP.LINE '                ** line approx.
11510 FOR J=1 TO N
11520   H=HA(J):K=KA(J):L=LA(J)
11530   IF RLA(J)>1/DMIN THEN GOTO 11830
11540   XPR=FNXCODS(H,K,L):YPR=FNXCODS(H,K,L):ZPR=FNZCODS(H,K,L)
11550   GG=XPR*XPR+YPR*YPR+ZPR*ZPR
11560   GOSUB *PRJ: XJ=XPR:YJ=YPR:ZJ=ZPR
11570   X=XJ*CO+YJ*SI:Y=-XJ*SI+YJ*CO:Z=ZJ '                ** reciprocal lattice point
11580   COPS=FNSCPR(0,0,1,X,Y,Z)
11590   RY=SQR(WN2-GG/4) : RX=RY*COPS
11600   ANG=180:STOP STOP:GOSUB *ELLIPSE :STOP ON
11610   IF INAREA=0 THEN GOTO 11830
11620   IF ABS(X)<.0001 THEN GOTO *XEQO
11630   IF ABS(Y)<.0001 THEN GOTO *YEQO
11640   XL(1)=-Y/X*(XYMAX-YY)+XX :YL(1)=XYMAX
11650   XYL2(1)=XL(1)^2+YL(1)^2
11660   XL(2)=-Y/X*(-XYMAX-YY)+XX :YL(2)=-XYMAX
11670   XYL2(2)=XL(2)^2+YL(2)^2
11680   YL(3)=-X/Y*(XYMAX-XX)+YY :XL(3)=XYMAX
11690   XYL2(3)=XL(3)^2+YL(3)^2
11700   YL(4)=-X/Y*(-XYMAX-XX)+YY :XL(4)=-XYMAX
11710   XYL2(4)=XL(4)^2+YL(4)^2
11720   FOR IJ=1 TO 4
11730     FOR IJ2=1 TO IJ
11740       XLA=XL(IJ2):YLA=YL(IJ2):XYLA=XYL2(IJ2)
11750       IF XYL2(IJ)>XYL2(IJ2) THEN 11790
11760       XL(IJ2)=XL(IJ):YL(IJ2)=YL(IJ):XYL2(IJ2)=XYL2(IJ)
11770       YL(IJ2)=YLA:YL(IJ)=YLA
11780       XYL2(IJ2)=XYL2(IJ):XYL2(IJ)=XYLA
11790     NEXT IJ2
11800   XPL(0)=XL(1):YPL(0)=YL(1):XPL(1)=XL(2):YPL(1)=YL(2)
11810   IF ABS(XPL(1))>XYMAX OR ABS(YPL(1))>XYMAX THEN GOTO 11830
11820   STOP STOP:GOSUB *PLOT :STOP ON
11830   NEXT J
11840   STOP STOP:GOSUB *SCALE :GOSUB *WID :STOP ON
11850   IF PRPL=2 THEN STOP STOP:GOSUB *TEXT :LPRINT "SPO;":STOP ON:RETURN
11860   WINDOW (-XYMX,-XYMX)-(XYMX,XYMX):VIEW (210,0)-(609,399)
11870   RETURN
11880   *XEQO
11890   XL(1)=XYMAX:YL(1)=YY
11900   XL(2)=-XYMAX:YL(2)=YY
11910   GOTO 11800
11920   *YEQO
11930   XL(1)=XX:YL(1)=XYMAX
11940   XL(2)=XX:YL(2)=-XYMAX
11950   GOTO 11800
11960 '
11970 *CURVE
11980 FOR J=1 TO N
11990   H=HA(J):K=KA(J):L=LA(J)
12000   IF RLA(J)>1/DMIN THEN GOTO 12380
12010   XPR=FNXCODS(H,K,L):YPR=FNXCODS(H,K,L):ZPR=FNZCODS(H,K,L)
12020   GG=XPR*XPR+YPR*YPR+ZPR*ZPR
12030   GOSUB *PRJ: XJ=XPR:YJ=YPR:ZJ=ZPR
12040   X=XJ*CO+YJ*SI:Y=-XJ*SI+YJ*CO:Z=ZJ '                ** reciprocal lattice point
12050   COPS=FNSCPR(0,0,1,X,Y,Z)
12060   RY=SQR(WN2-GG/4) : RX=RY*COPS
12070   ANG=180:STOP STOP:GOSUB *ELLIPSE :STOP ON
12080   IF INAREA=0 THEN GOTO 12380
12090   STOP STOP
12100   ANG=30:GOSUB *ELLIPSE :IF INAREA=0 THEN 12120
12110   SANG=0:EANG=360:GOTO 12250
12120   ANG=60:GOSUB *ELLIPSE :IF INAREA=0 THEN 12140
12130   SANG=30:EANG=330:GOTO 12250
12140   ANG=90:GOSUB *ELLIPSE :IF INAREA=0 THEN 12160
12150   SANG=60:EANG=300:GOTO 12250
12160   ANG=120:GOSUB *ELLIPSE :IF INAREA=0 THEN 12180
12170   SANG=90:EANG=270:GOTO 12250
12180   ANG=150:GOSUB *ELLIPSE :IF INAREA=0 THEN 12200
12190   SANG=120:EANG=240:GOTO 12250
12200   ANG=170:GOSUB *ELLIPSE :IF INAREA=0 THEN 12220
12210   SANG=150:EANG=210:GOTO 12250
12220   ANG=178:GOSUB *ELLIPSE :IF INAREA=0 THEN 12240
12230   SANG=170:EANG=190:GOTO 12250
12240   SANG=178:EANG=182
12250   STOP ON:NP=0:IN=0:CIRS=0:CIRE=0:XPL(0)=0:YPL(0)=0
12260   FOR ANG=SANG TO EANG STEP ANGSTEP
12270     STOP STOP:GOSUB *ELLIPSE:STOP ON
12280     IF ABS(XX)>XYMAX THEN INAREA=0 : GOTO 12310
12290     IF ABS(YY)>XYMAX THEN INAREA=0 : GOTO 12310
12300     IF INAREA=1 THEN GOTO 12340

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12310 IF IN=0 THEN XPL(0)=XX:YPL(0)=YY:GOTO 12360
12320 IF IN=1 THEN STOP STOP:GOSUB *PLOT:STOP ON
12330 XPL(0)=XX:YPL(0)=YY:GOTO 12360
12340 NP=NP+1:IN=1:XPL(NP)=XX:YPL(NP)=YY
12350 XPL(NP+1)=XX:YPL(NP+1)=YY
12360 NEXT ANG
12370 IF NP>0 THEN CIRE=1:STOP STOP:GOSUB *PLOT:STOP ON
12380 NEXT J
12390 STOP STOP:GOSUB *SCALE :GOSUB *WID:STOP ON
12400 ON STOP GOSUB *STRP
12410 IF PRPL=2 THEN GOSUB *TEXT:LPRINT "SPO;":RETURN
12420 WINDOW (-XYMX,-XYMX)-(XYMX,XYMX):VIEW (210,0)-(609,399)
12430 RETURN
12440 *STRP1
12450 ON STOP GOSUB *STRP
12460 IF PRPL=2 THEN LPRINT "PU;SPO;":RETURN
12470 WINDOW (-XYMX,-XYMX)-(XYMX,XYMX):VIEW (210,0)-(609,399)
12480 RETURN
12490 *PLOT
12500 IF PRJLC=1 THEN NP=0:GOTO 12570
12510 XPL(NP+1)=XX:YPL(NP+1)=YY
12520 IF XPL(0)=0 AND YPL(0)=0 THEN CIRS=1
12530 IF CIRS=0 THEN GOSUB *SPOINT
12540 IF CIRE=0 THEN GOSUB *EPOINT
12550 IF CIRS=1 THEN XPL(0)=XPL(1):YPL(0)=YPL(1)
12560 IF CIRE=1 THEN XPL(NP+1)=XPL(NP):YPL(NP+1)=YPL(NP)
12570 NSER=NSER+1
12580 IHKL$(NSER)=STR$(H)+" "+STR$(K)+" "+STR$(L)
12590 XPLS(NSER)=XPL(0):YPLS(NSER)=YPL(0)
12600 XPLE(NSER)=XPL(NP+1):YPLE(NSER)=YPL(NP+1)
12610 COL=1 : IF NIL=1 THEN 12660
12620 FOR JI=NIL-1 TO 1 STEP -1
12630 IF 1/RLA(J)>BOUND(JI) THEN COL=NIL-JI+1
12640 NEXT
12650 ON COWI GOTO *CCHAN, *WCHAN
12660 *CCHAN
12670 COL=NIL-COL+1
12680 ON PRPL GOTO 12690,12820
12690 '* C R T *
12700 IF COL>4 THEN 12760
12710 ON COL GOTO 12720,12730,12740,12750
12720 COL=7:GOTO 12770
12730 COL=5:GOTO 12770
12740 COL=2:GOTO 12770
12750 COL=1:GOTO 12770
12760 COL=1
12770 FOR JNP=0 TO NP
12780 LINE (XPL(JNP),-YPL(JNP))-(XPL(JNP+1),-YPL(JNP+1)),COL
12790 NEXT
12800 NP=0:IN=0:XPL(0)=0:YPL(0)=0
12810 RETURN
12820 '* Plotter *
12830 FOR JNP=0 TO NP+1
12840 XPL(JNP)=FIX(XPL(JNP)*1E+06)/10000
12850 YPL(JNP)=FIX(YPL(JNP)*1E+06)/10000
12860 NEXT
12870 LPRINT "SP";COL;";VS";VS;";"
12880 FOR JNP=0 TO NP+1
12890 LPRINT "PA";XPL(JNP);";";YPL(JNP);";PD;";
12900 NEXT
12910 LPRINT "PU;"
12920 IF NINDEX=0 THEN GOSUB *INDEXING
12930 NP=0:IN=0:XPL(0)=0:YPL(0)=0
12940 RETURN
12950 '
12960 *WCHAN
12970 ON PRPL GOTO 12980 , 13160
12980 '* C R T *
12990 WXYO=XYMAX/391
13000 IF NIL=2 AND COL=2 THEN COL=3
13010 FOR JCOL=1 TO COL
13020 WXY=WXYO*(2*JCOL-COL-1)
13030 SJNP=0:EJNP=NP
13040 IF XPL(0)=XPL(1) AND YPL(0)=YPL(1) THEN SJNP=1
13050 IF XPL(NP)=XPL(NP+1) AND YPL(NP)=YPL(NP+1) THEN EJNP=NP-1
13060 FOR JNP=SJNP TO EJNP
13070 WXO=YPL(JNP+1)-YPL(JNP)
13080 WYO=-XPL(JNP+1)+XPL(JNP)
13090 WWXY=SQR(WXO*WXO+WYO*WYO)
13100 WX=WXO*WXY/WWXY:WY=WYO*WXY/WWXY
13110 LINE (XPL(JNP)+WX,-YPL(JNP)-WY)-(XPL(JNP+1)+WX,-YPL(JNP+1)-WY)
13120 NEXT

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13130 NEXT JCOL
13140 NP=0:IN=0:XPL(0)=0:YPL(0)=0
13150 RETURN
13160 ' * plotter *
13170 WXYO=XYMAX/(650/1.2)
13180 IF NIL=2 AND COL=2 THEN COL=3
13190 FOR JCOL=1 TO COL
13200 WXY=WXYO*(2*JCOL-COL-1)
13210 FOR JNP=0 TO NP
13220 WXO=YPL(JNP+1)-YPL(JNP)
13230 WYO=-XPL(JNP+1)+XPL(JNP)
13240 WWXY=SQR(WXO*WXO+WYO*WYO)
13250 WX=WXO*WXY/WWXY : WY=WYO*WXY/WWXY
13260 XPLL(JNP)=XPL(JNP)+WX
13270 YPLL(JNP)=YPL(JNP)+WY
13280 XPLL(JNP)=FIX(XPLL(JNP)*1E+06)/10000
13290 YPLL(JNP)=FIX(YPLL(JNP)*1E+06)/10000
13300 NEXT
13310 XPLL(NP+1)=XPL(NP+1)+WX
13320 YPLL(NP+1)=YPL(NP+1)+WY
13330 XPLL(NP+1)=FIX(XPLL(NP+1)*1E+06)/10000
13340 YPLL(NP+1)=FIX(YPLL(NP+1)*1E+06)/10000
13350 FOR JNP=0 TO NP+1
13360 IJNP=FNEVOD(JCOL):JJNP=ABS((NP+1)*IJNP-JNP)
13370 LPRINT "PA";XPLL(JJNP);",",YPLL(JJNP);";PD;";
13380 NEXT
13390 LPRINT "PU;";
13400 NEXT JCOL
13410 XPL(0)=FIX(XPL(0)*1E+06)/10000
13420 YPL(0)=FIX(YPL(0)*1E+06)/10000
13430 XPL(NP+1)=FIX(XPL(NP+1)*1E+06)/10000
13440 YPL(NP+1)=FIX(YPL(NP+1)*1E+06)/10000
13450 IF NINDEX=0 THEN GOSUB *INDEXING
13460 NP=0:IN=0:XPL(0)=0:YPL(0)=0
13470 RETURN
13480 *SCALE
13490 IF ANGRAN=>60 THEN ANGSCALE=20:GOTO *SCALING
13500 IF ANGRAN=>30 THEN ANGSCALE=10:GOTO *SCALING
13510 IF ANGRAN=>15 THEN ANGSCALE= 5:GOTO *SCALING
13520 IF ANGRAN=> 6 THEN ANGSCALE= 2:GOTO *SCALING
13530 IF ANGRAN=> 3 THEN ANGSCALE= 1:GOTO *SCALING
13540 IF ANGRAN=> 1.5 THEN ANGSCALE= .5:GOTO *SCALING
13550 IF ANGRAN=> 1 THEN ANGSCALE= .2:GOTO *SCALING
13560 IF ANGRAN=> .5 THEN ANGSCALE= .1:GOTO *SCALING
13570 IF ANGRAN<.5 THEN RETURN
13580 *SCALING
13590 ON PRPL GOTO 13600,13810
13600 ' ** C R T **
13610 WINDOW (0,0)-(639,399)
13620 VIEW (0,0)-(639,399)
13630 FOR SCI=0 TO ANGRAN STEP ANGSCALE
13640 FOR IJ=-1 TO 1 STEP 2
13650 SCJ=SCI*IJ
13660 ON PRJ GOTO 13670,13680
13670 Y=WN*TAN(SCJ*PI/180):GOTO 13690
13680 Y=2*WN*TAN(SCJ*PI/360)
13690 YSCJ=199+Y*190/XYMAX
13700 LINE (205,199)-(205, YSCJ):LINE (202, YSCJ)-(208, YSCJ)
13710 SSCJ$=STR$(ABS(SCJ)):LSCJ=LEN(SSCJ$):IF LSCJ>4 THEN LSCJ=4
13720 FOR J=1 TO LSCJ
13730 MSCJ$=MID$(SSCJ$, J, 1):MSCJ=ASC(MSCJ$)+256
13740 PUT (190-8*(LSCJ-J), YSCJ-4), KANJI(MSCJ), OR
13750 NEXT J
13760 NEXT IJ
13770 NEXT SCI
13780 WINDOW (-XYMX, -XYMX)-(XYMX, XYMX)
13790 VIEW (210,0)-(609,399)
13800 RETURN
13810 ' * plotter *
13820 LPRINT "SP1;IW;SIO.18,0.25;PU";-XYMAX*150;";0;DIO,-1;";
13830 LPRINT "CP-5,-2.2;LBangl (deg)";CHR$(3);";PU";-XYMAX*150;";0;";
13840 FOR J=1 TO 100
13850 ANGJ=J*ANGSCALE:IF ANGJ>ANGRAN THEN ANGJ=ANGJ-ANGSCALE:GOTO 13870
13860 NEXT
13870 FOR SCJ=-ANGJ TO ANGJ STEP ANGSCALE
13880 ON PRJ GOTO 13890,13900
13890 Y=WN*TAN(SCJ*PI/180):GOTO 13910
13900 Y=2*WN*TAN(SCJ*PI/360)
13910 LPRINT "PA";-XYMAX*150;";",Y*100;";YT;";
13920 LPRINT "PU;SIO.1,0.2;CP-1.8,-1;LB";ABS(SCJ);CHR$(3);
13930 LPRINT "PU";-XYMAX*150;";",Y*100;";PD;";
13940 NEXT

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13950 LPRINT "PU;PA;DI1,0;"
13960 RETURN
13970 *SPOINT ' * calculate start point *
13980 XPL1=XPL(0):YPL1=YPL(0):XPL2=XPL(1):YPL2=YPL(1)
13990 GOSUB *SEPOINT:XPL(0)=XSL:YPL(0)=YSL
14000 RETURN
14010 *EPOINT ' * calculate end point *
14020 XPL2=XPL(NP):YPL2=YPL(NP):XPL1=XPL(NP+1):YPL1=YPL(NP+1)
14030 GOSUB *SEPOINT:XPL(NP+1)=XSL:YPL(NP+1)=YSL
14040 RETURN
14050 *SEPOINT ' * calculate start and end point
14060 IF XPL1>XYMAX AND YPL1>XYMAX THEN CASE=1:GOTO 14140
14070 IF XPL1>XYMAX AND ABS(YPL1)<XYMAX THEN CASE=2:GOTO 14140
14080 IF XPL1>XYMAX AND YPL1<-XYMAX THEN CASE=3:GOTO 14140
14090 IF ABS(XPL1)<XYMAX AND YPL1>XYMAX THEN CASE=4:GOTO 14140
14100 IF ABS(XPL1)<XYMAX AND YPL1<-XYMAX THEN CASE=5:GOTO 14140
14110 IF XPL1<-XYMAX AND YPL1>XYMAX THEN CASE=6:GOTO 14140
14120 IF XPL1<-XYMAX AND ABS(YPL1)<XYMAX THEN CASE=7:GOTO 14140
14130 IF XPL1<-XYMAX AND YPL1<-XYMAX THEN CASE=8
14140 ON CASE GOTO 14150,14220,14240,14310,14330,14350,14420,14440
14150 XSL1=XYMAX:YSL1=YPL1+(YPL1-YPL2)*(XYMAX-XPL1)/(XPL1-XPL2)
14160 YSL2=XYMAX:XSL2=XPL1+(XPL1-XPL2)*(XYMAX-YPL1)/(YPL1-YPL2)
14170 RXSL1=XSL1*XSL1+YSL1*YSL1
14180 RXSL2=XSL2*XSL2+YSL2*YSL2
14190 XSL=XSL1:YSL=YSL1
14200 IF RXSL1>RXSL2 THEN XSL=XSL2:YSL=YSL2:RETURN
14210 RETURN
14220 XSL=XYMAX:YSL=YPL1+(YPL1-YPL2)*(XYMAX-XPL1)/(XPL1-XPL2)
14230 RETURN
14240 XSL1=XYMAX:YSL1=YPL1+(YPL1-YPL2)*(XYMAX-XPL1)/(XPL1-XPL2)
14250 YSL2=-XYMAX:XSL2=XPL1-(XPL1-XPL2)*(XYMAX+YPL1)/(YPL1-YPL2)
14260 RXSL1=XSL1*XSL1+YSL1*YSL1
14270 RXSL2=XSL2*XSL2+YSL2*YSL2
14280 XSL=XSL1:YSL=YSL1
14290 IF RXSL1>RXSL2 THEN XSL=XSL2:YSL=YSL2:RETURN
14300 RETURN
14310 YSL=XYMAX:XSL=XPL1+(XPL1-XPL2)*(XYMAX-YPL1)/(YPL1-YPL2)
14320 RETURN
14330 YSL=-XYMAX:XSL=XPL1-(XPL1-XPL2)*(XYMAX+YPL1)/(YPL1-YPL2)
14340 RETURN
14350 XSL1=-XYMAX:YSL1=YPL1-(YPL1-YPL2)*(XYMAX+XPL1)/(XPL1-XPL2)
14360 YSL2=XYMAX:XSL2=XPL1+(XPL1-XPL2)*(XYMAX-YPL1)/(YPL1-YPL2)
14370 RXSL1=XSL1*XSL1+YSL1*YSL1
14380 RXSL2=XSL2*XSL2+YSL2*YSL2
14390 XSL=XSL1:YSL=YSL1
14400 IF RXSL1>RXSL2 THEN XSL=XSL2:YSL=YSL2:RETURN
14410 RETURN
14420 XSL=-XYMAX:YSL=YPL1-(YPL1-YPL2)*(XYMAX+XPL1)/(XPL1-XPL2)
14430 RETURN
14440 XSL1=-XYMAX:YSL1=YPL1-(YPL1-YPL2)*(XYMAX+XPL1)/(XPL1-XPL2)
14450 YSL2=-XYMAX:XSL2=XPL1-(XPL1-XPL2)*(XYMAX+YPL1)/(YPL1-YPL2)
14460 RXSL1=XSL1*XSL1+YSL1*YSL1
14470 RXSL2=XSL2*XSL2+YSL2*YSL2
14480 XSL=XSL1:YSL=YSL1
14490 IF RXSL1>RXSL2 THEN XSL=XSL2:YSL=YSL2:RETURN
14500 RETURN
14510 '
14520 *INDEXING
14530 IF CIRS=1 OR CIRE=1 THEN GOTO *INDCIR
14540 ON 1+FNEVOD(INT(RND*100)) GOTO *INDS,*INDE
14550 *INDS ' * index at start point *
14560 XIND=XPL(0):YIND=YPL(0) ' * start point *
14570 IF ABS(XYMAX*100-ABS(YIND))<.01 THEN GOTO 14600
14580 IF XIND>0 THEN PIND=1 ELSE PIND=3
14590 GOTO *POSIND
14600 IF YIND>0 THEN PIND=2 ELSE PIND=4
14610 GOTO *POSIND
14620 XIND=XPL(NP+1):YIND=YPL(NP+1) ' * end point *
14630 IF ABS(XYMAX*100-ABS(YIND))<.01 THEN 14660
14640 IF XIND>0 THEN PIND=1 ELSE PIND=3
14650 GOTO *POSIND
14660 IF YIND>0 THEN PIND=2 ELSE PIND=4
14670 GOTO *POSIND
14680 *INDE ' * index at end point *
14690 XIND=XPL(NP+1):YIND=YPL(NP+1) ' * end point *
14700 IF ABS(XYMAX*100-ABS(YIND))<.01 THEN GOTO 14730
14710 IF XIND>0 THEN PIND=1 ELSE PIND=3
14720 GOTO *POSIND
14730 IF YIND>0 THEN PIND=2 ELSE PIND=4
14740 GOTO *POSIND
14750 XIND=XPL(0):YIND=YPL(0) ' * start point *
14760 IF ABS(XYMAX*100-ABS(YIND))<.01 THEN 14790

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15590 UZA=FIX(X3*1000)/1000:VZA=FIX(Y3*1000)/1000:WZA=FIX(Z3*1000)/1000
15600 RETURN
15610 *MENU
15620 LOCATE 0,12
15630 PRINT " space : get ":PRINT " E : end(cancel)":PRINT
15640 PRINT "ten key : cursor control":PRINT
15650 PRINT " Q : quick ":PRINT " S : slow "
15660 RETURN
15670 *TY4 ' left
15680 PUT (XP,YP),IG2%,AND:XP=XP-ST:IF XP<10 THEN XP=XP+ST
15690 GET (XP,YP)-STEP(9,9),IG2%:PUT (XP,YP),IG%,OR
15700 RETURN
15710 *TY2 ' down
15720 PUT (XP,YP),IG2%,AND:YP=YP+ST:IF YP>389 THEN YP=YP-ST
15730 GET (XP,YP)-STEP(9,9),IG2%:PUT (XP,YP),IG%,OR
15740 RETURN
15750 *TY6 ' right
15760 PUT (XP,YP),IG2%,AND:XP=XP+ST:IF XP>389 THEN XP=XP-ST
15770 GET (XP,YP)-STEP(9,9),IG2%:PUT (XP,YP),IG%,OR
15780 RETURN
15790 *TY8 ' up
15800 PUT (XP,YP),IG2%,AND:YP=YP-ST:IF YP<10 THEN YP=YP+ST
15810 GET (XP,YP)-STEP(9,9),IG2%:PUT (XP,YP),IG%,OR
15820 RETURN
15830 *TY1 ' left-down
15840 GOSUB *TY2:GOSUB *TY4 :RETURN
15850 *TY3 ' right-down
15860 GOSUB *TY6:GOSUB *TY2 :RETURN
15870 *TY9 ' right-up
15880 GOSUB *TY8:GOSUB *TY6 :RETURN
15890 *TY7 ' left-up
15900 GOSUB *TY4:GOSUB *TY8 :RETURN
15910 *TYQ ' speed up
15920 IF ST=>1 THEN ST=ST+1 ELSE ST=ST*2
15930 IF ST>10 THEN ST=ST-1
15940 RETURN
15950 *TYS ' speed down
15960 IF ST>1 THEN ST=ST-1 ELSE ST=ST/2
15970 IF ST<.125 THEN ST=.125
15980 RETURN
15990 *TYC ' cursor clear
16000 PUT (XP,YP),IG2%,AND:GET (XP,YP)-STEP(9,9),IG2%
16010 RETURN
16020 *F257
16030 FOR IJ=0 TO 33:IG4%(IJ)=IG2%(IJ):NEXT
16040 XP01=XP:YP01=YP
16050 RETURN
16060 *F257E
16070 PUT (XP01,YP01),IG4%,AND
16080 RETURN

```

Language : N88BASIC (86) COMPILER
DOS : MS-DOS
Computer : NEC PC-9801
Printer : NEC PC-PR201
Plotter : ROLAND DXY-990

## Thickness determination program

This method of specimen thickness determination is based upon the method of Kelly *et al.* This program computes ten sets of specimen thickness, extinction distance and the fourth power of a correlation coefficient, when the measured distance between the bright-field disk and a dark-field disk,  $L_0$ , and those between the exact Bragg position and each of successive minima,  $L_i$ , are used as input data. When the correlation coefficients have a simi-

lar value for a few thicknesses, the thickness exhibiting a reasonable extinction distance is selected as the correct one.

### Reference

- [a] P.M. Kelly, A. Jostsons, R.G. Blake and J.G. Napier: *phys. stat. sol.*, (a) **31** (1975) 771.

### Input data

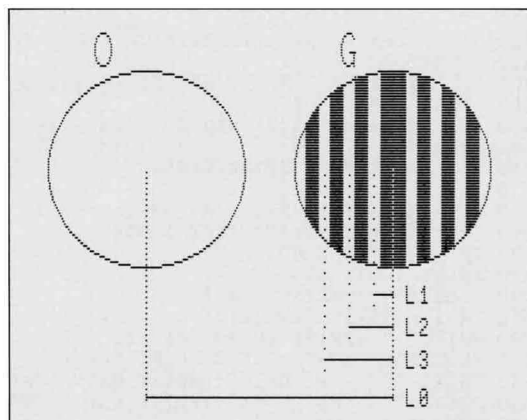
```

Calculation of foil thickness
  by T.Kaneyama, M.Terauchi and M.Tanaka, Dept of Phys., Fac. of Science, Tohoku
  Univ.
    ( refs. P.M.Kelly et al.: phys. stat. sol. (a):31(1975)771
      M.Tanaka and M.Terauchi: Convergent-Beam Electron Diffraction(1985)
      JEOL-Mruzen, P.38-39 )
1)Accelerating voltage (kV)? 62.8
2)Lattice paramater      a,b,c(A) =? 5.43,5.43,5.43
      alpha,beta,gamma(deg) =? 90,90,90
3)Index of G (h,k,l) ? 2,-2,0
4)Number of data Li ? 4
5)Distance between 0 and G reflection  L 0 =? 1
6)Distances between successive subsidiary minima
      and the exact Bragg position of G
      L 1 =? 0.0798
      L 2 =? 0.180
      L 3 =? 0.261
      L 4 =? 0.343
  
```

### Output

n1:	Thickness(A)	Extinction distance(A)	Fourth power of correlation coef.
1:	T= 877.5	GSI= 2120.6	r <sup>4</sup> = 0.4251
2:	T= 1073.3	GSI= 642.6	r <sup>4</sup> = 0.9974
3:	T= 1228.7	GSI= 448.3	r <sup>4</sup> = 0.9852
4:	T= 1362.2	GSI= 360.1	r <sup>4</sup> = 0.9766
5:	T= 1481.6	GSI= 308.0	r <sup>4</sup> = 0.9716
6:	T= 1590.9	GSI= 272.8	r <sup>4</sup> = 0.9685
7:	T= 1692.5	GSI= 247.1	r <sup>4</sup> = 0.9664
8:	T= 1787.8	GSI= 227.4	r <sup>4</sup> = 0.9651
9:	T= 1878.0	GSI= 211.7	r <sup>4</sup> = 0.9641
10:	T= 1963.8	GSI= 198.7	r <sup>4</sup> = 0.9634

### Illustration



```

10 REM file name 'Thickness'
20 SCREEN 0,0:CLS 3
30 COLOR 4:PRINT " Calculation of foil thickness ":COLOR 0
40 PRINT "   by T.Kaneyama,M.Terauchi and M.Tanaka, Dept of Phys., Fac. of Science, Tohoku Univ."
50 CONSOLE 3,4,0,0
60 PRINT "   ( refs. P.M.Kelly et al.: phys. stat. sol. (a):31(1975)771"
70 PRINT "     M.Tanaka and M.Terauchi:Convergent-Beam Electron Diffraction(1985) JEOL-Maruzen, P.38-39 )"
80 GOSUB *SML
90 OPTION BASE 1
100 DIM T(100),S(100),SN(100),X(100),Y(100),TA(100),SA(100),XA(100),YA(100)
110 DIM TT(10),GS(10),R(10)
120 INPUT "1)Accelerating voltage (kV)";E
130 INPUT "2)Lattice paramater a,b,c(A) =";A,B,C
140 INPUT "   alpha,beta,gamma(deg) =";ALPH,BETA,GAMM
150 INPUT "3)Index of G (h,k,l) ";H,K,L
160 '
170 PI=3.14159
180 LAM=12.26/SQR(1000*E*(1+9.788E-07*1000*E))
190 ALP=ALPH*PI/180 : BET=BETA*PI/180 : GAM=GAMM*PI/180
200 SIA=SIN(ALP):SIB=SIN(BET):SIG=SIN(GAM)
210 COA=COS(ALP):COB=COS(BET):COG=COS(GAM)
220 S11=B*B*C*C*SIA^2:S22=A*A*C*C*SIB^2:S33=A*A*B*B*SIG^2
230 S12=A*B*C*C*(COA*COB-COG):S23=A*A*B*C*(COB*COG-COA)
240 S13=A*B*B*C*(COG*COA-COB):VC=A*B*C*SQR(1-COA^2-COB^2-COG^2+2*COA*COB*COG)
250 D2=S11*H*H+S22*K*K+S33*L*L+2*S12*H*K+2*S23*K*L+2*S31*L*H
260 D=VC/SQR(D2)
270 INPUT "4)Number of data Li ";ND
280 INPUT "5)Distance between 0 and G reflection L 0 =";T2
290 PRINT "6)Distances between successive subsidiary minima "
300 PRINT "   and the exact Bragg position of G"
310 FOR I=1 TO ND
320 PRINT " L";I;"=";:INPUT T(I)
330 S(I)=LAM*T(I)/(D^2*T2)
340 NEXT I
350 CONSOLE 0,25
360 '
370 CLS 1
380 PRINT "n1: Thickness(A)           Extinction           Fourth power of"
390 PRINT "                               distance(A)           correlation coef."
400 FOR I=1 TO 10
410 N(I)=I : X(1)=1/I^2 : Y(1)=(S(1)/I)^2
420 XT=X(1):YT=Y(1):SXT=X(1)^2:XYT=X(1)*Y(1)
430 '
440 FOR J=2 TO ND
450 N(J)=N(J-1)+1
460 X(J)=1/N(J)^2
470 Y(J)=(S(J)/N(J))^2
480 XT=XT+X(J) : YT=YT+Y(J) : SXT=SXT+X(J)^2 : XYT=XYT+X(J)*Y(J)
490 NEXT J
500 MX=XT/ND : MY=YT/ND : SX2=0:SY2=0
510 FOR J=1 TO ND
520 SX2=SX2+(X(J)-MX)^2 : SY2=SY2+(Y(J)-MY)^2
530 NEXT J
540 SX2=SX2/ND : SY2=SY2/ND
550 '
560 TT=(XT*XYT-YT*SXT)/(XT^2-ND*SXT) : TT(I)=1/SQR(ABS(TT))
570 GG=-(XT*YT-ND*XYT)/(XT^2-ND*SXT)
580 IF GG<>0 THEN 600
590 PRINT :GOTO 660
600 GS(I)=1/SQR(ABS(GG))
610 R(I)=-GG*SQR(SX2/SY2)
620 PRINT " " :PRINT USING "##";I;
630 PRINT " : T=";:PRINT USING "#####.##";TT(I);
640 PRINT "   GSI=";:PRINT USING "#####.##";GS(I);
650 PRINT "   r^4=";:PRINT USING "###.####";R(I)^4
660 NEXT I
670 CLS 2
680 PRINT :INPUT " 7)OUTPUT TO THE PRINTER?(y/n)";PRS
690 IF PRS="N" OR PRS="n" THEN END
700 LPRINT "n1: Thickness(A)           Extinction           Fourth power of"
710 LPRINT "                               distance(A)           correlation coef."
720 FOR I=1 TO 10
730 IF GS(I)=0 AND R(I)=0 THEN PRINT :GOTO 780
740 LPRINT " ":LPRINT USING "##";I;
750 LPRINT " : T=";:LPRINT USING "#####.##";TT(I);
760 LPRINT "   GSI=";:LPRINT USING "#####.##";GS(I);
770 LPRINT "   r^4=";:LPRINT USING "###.####";R(I)^4
780 NEXT I
790 '
800 END
810 *SML

```

```

820 WINDOW (0,0)-(199,149)
830 VIEW (139,0)-(499,199)
840 CIRCLE (49,79),40:CIRCLE (149,79),40
850 LINE (144,53)-(144,106):LINE (139,53)-(139,105)
860 LINE (134,54)-(134,103):LINE (129,56)-(129,102)
870 LINE (124,59)-(124,99) :LINE (119,62)-(119,96)
880 LINE (114,67)-(114,92) :LINE (154,53)-(154,106)
890 LINE (159,53)-(159,105):LINE (164,54)-(164,103)
900 LINE (169,56)-(169,102):LINE (174,59)-(174,101)
910 LINE (179,62)-(179,97) :LINE (184,68)-(184,92)
920 PAINT (149,79),7:PAINT (137,79),7:PAINT (127,79),7:PAINT (117,79),7
930 PAINT (161,79),7:PAINT (171,79),7:PAINT (181,79),7
940 LINE (149,79)-(149,144),0
950 LINE (49,79)-(49,144),4,,&H5555:LINE (149,79)-(149,144),4,,&H5555
960 LINE (141.5,79)-(141.5,118),6,,&H2222:LINE (131.5,79)-(131.5,127),6,,&H2222
970 LINE (121.5,79)-(121.5,136),6,,&H2222:LINE (49,142)-(149,142),4
980 LINE (141.5,114)-(149,114),6
990 LINE (131.5,123)-(149,123),6:LINE (121.5,132)-(149,132),6
1000 PUT (49,55),KANJI(&H234F) : PUT (229,55),KANJI(&H2347)
1010 PUT (279,187),KANJI(&H14C),,2,0 :PUT (289,187),KANJI(&H130),,2,0
1020 PUT (279,149),KANJI(&H14C),,2,0 :PUT (289,149),KANJI(&H131),,2,0
1030 PUT (279,161),KANJI(&H14C),,2,0 :PUT (289,161),KANJI(&H132),,2,0
1040 PUT (279,173),KANJI(&H14C),,2,0 :PUT (289,173),KANJI(&H133),,2,0
1050 RETURN

```

Language : N88BASIC (86) COMPILER DOS : MS-DOS Computer : NEC PC-9801 Printer : NEC PC-PR201
---

# Simulations of reflection lines crossing various types of dislocations

This program simulates the profiles of reflections crossing a screw, an edge, a mixed and a partial dislocation, a dislocation dipole and an extended dislocation.

## Specification

```

programs : AUTOEXEC.BAT
          BATCH .BAT
          CONTROL .EXE
          DIS-S .EXE
          DIS-M .EXE
          DIS-MP .EXE
          DIS2-SF .EXE
          PICTURE .EXE
          PATTRN-5.DAT

language : N88BASIC(86) COMPILER

DOS      : MS-DOS

computer : NEC PC-9801

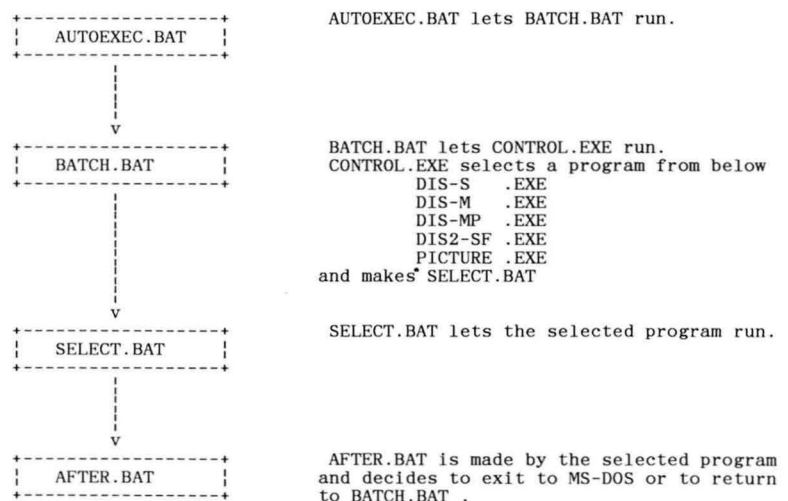
printer  : NEC PC-PR201
    
```

\*\*\*\*\* provisos \*\*\*\*\*

Notes for the use of other computers and printers.

1. All the programs written in BASIC must be compiled in advance because of batch processing upon MS-DOS.
2. The alternation of codes in the subroutine \*PRN. in PICTURE.BAS may be required for other printers.
3. The alternation of the standard dot patterns in PATTRN-5.DAT may be required for other printers.

## Flow chart



## Function of each program

CONTROL .EXE	Selection of the program to run
DIS-S .EXE	Calculation of the rocking curves around the screw dislocation
DIS-M .EXE	Calculation of the rocking curves around the mixed or edge dislocation
DIS-MP .EXE	Calculation of the rocking curves around the partial dislocation(screw,mixed & edge)
DIS2-SF .EXE	Calculation of the rocking curves around the dislocation dipole or extended dislocation
PICTURE .EXE	Printing out the rocking curves to a dot printer NEC PC-PR201 Image processing ; magnifying and interpolation filtering enhancement
PATTRN-5.DAT	Data file of the standard dot patterns

## CONTROL

ready CONTROL (ver. 1.4)

CONTROL selects a compiled program working on MS-DOS.

Input the number.

- 1 Calculation of the rocking curves around a dislocation
- 2 Printing out the rocking curves
- 3 Exit to MS-DOS

Calculation around single dislocation

- 1 Screw dislocation
- 2 Mixed or edge dislocation
- 3 Partial dislocation (screw, mixed & edge)

Calculation around a dislocation pair

- 4 Dislocation dipole or extended dislocation

## DIS-S

ready DIS-S

This program calculates the rocking curves around the screw dislocation.

\*\*\*\*\* Provisos \*\*\*\*\*

1. The dislocation is assumed to be parallel to the surface.
2. 2-beam & column approximations of the dynamical theory are used.
3. Euler's method is used for the integration along depth direction.
4. Length is in unit of angstrom.
5. Excitation error  $W$  is dimensionless.

- 1 Start calculation.
- 2 Return to CONTROL.

Set a diskette for data file to drive b:

- 1 Open new data file.
- 2 Append to old file.

Input the file name of the data file.  
test-s

- 1 Reflection vector  $g = -2 \ 2 \ 0$
- 2 Burgers vector  $b = .5 \ -.5 \ 0$

Value of  $n = g \cdot b = -2$

- 3 Thickness of the specimen 500
- 4 Depth of the dislocation 250
- 5 Mean extinction distance 1000
- 6 Extinction distance for the reflection 1000
- 7 Mean absorption distance 20000
- 8 Absorption distance for the reflection 20000
- 9 Range of the excitation error  $W$  (minimum) -10  
(maximum) 10
- 10
- 11 Range of distance from the dislocation (minimum) -125  
(maximum) 125
- 12
- 13 Total number of calculation points along the excitation error axis 45
- 14 Total number of calculation points along the distance axis 79
- 15 Total number of slabs perpendicular to the depth direction 250

Are all parameters right ?  
1 Yes.  
2 No.

## CONTROL

ready CONTROL (ver. 1.4)

CONTROL selects a compiled program working on MS-DOS.

Input the number.

- 1 Calculation of the rocking curves around a dislocation
- 2 Printing out the rocking curves
- 3 Exit to MS-DOS

## PICTURE

ready PICTURE

This program prints out the rocking curves to a dot printer using PRINTONE.

PRINTONE ( ver. 4.1 on May 12th, 1987 by S.Ito )  
is an image processing program  
to magnify-interpolate, enhance & filter

- 1 Print out.
- 2 Return to CONTROL.

com: Set the diskette with the data file to drive B:  
Input the file name.  
you: test-s  
com: Set a printer. (dot printer PC-PR201)  
Have the data already been processed by PICTURE ?  
1) Yes.  
2) No.

you: 2  
com: Select an output mode.  
1) Printer.  
2) FD file.  
3) Both printer & FD file.

you: 1  
com: How wide is the FORM-PAPER ?  
1) 10 inches (80 columns)  
2) 17 inches (136 columns)

you: 1  
com: Do you use standard dot patterns ?  
1) Yes.  
2) No.

you: 1  
com: Is the background color black or white ?  
1) Black.  
2) White.

you: 2  
com: Three functions are prepared;  
magnification, filtering and enhancement.

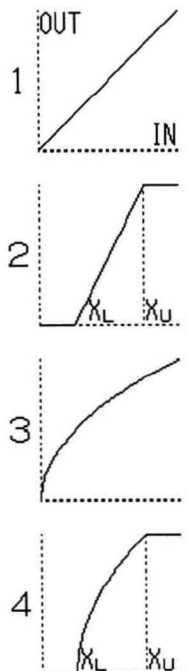
com: Input the magnifying power.  
(1, 2 or 3)

you: 3  
com: Input the order of interpolation.  
(1, 2, 3, 4, 5 or 6)

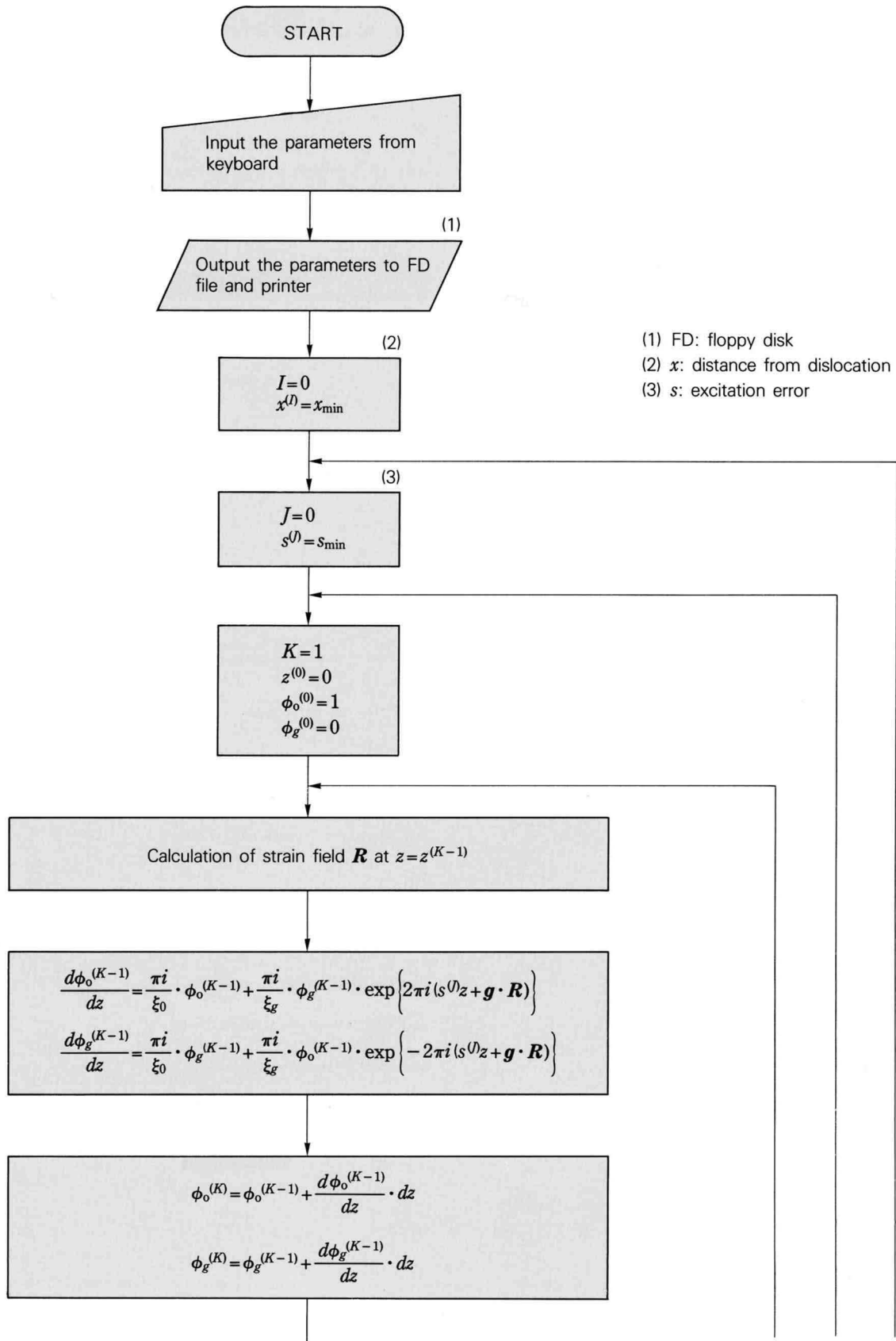
you: 2  
com: Input an enhancement function.  
(1, 2, 3, 4 in the right-side figures.)

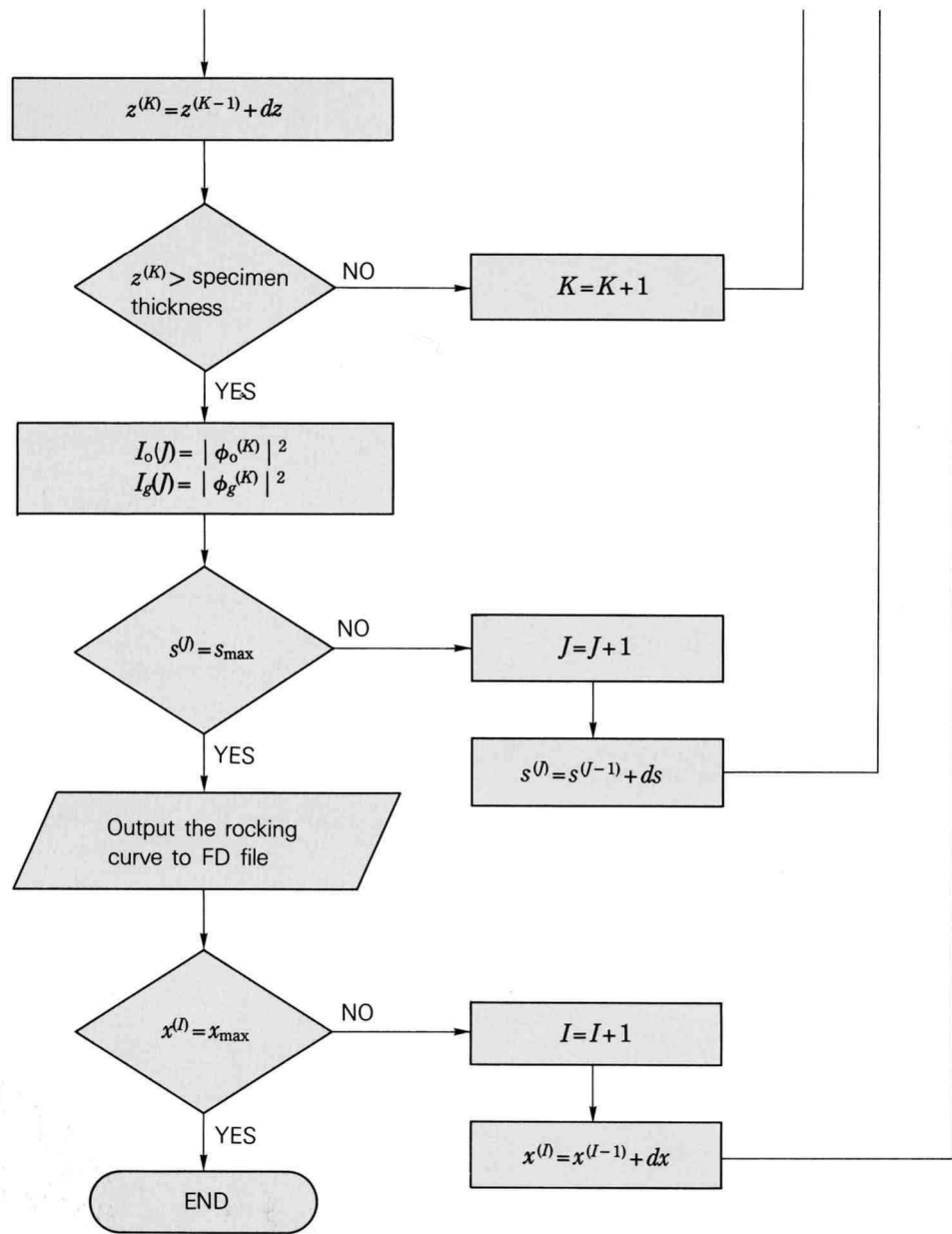
you: 1  
com: Do you start processing ?  
1) Yes.  
2) Return to title page.

you: 1  
com: Now computing. **Don't disturb.**



## Flow chart of calculation





## Input data

```
file name    test-s

***** assumptions for calculation *****

Rocking curves around the screw dislocation.
The dislocation is assumed to be parallel to the surface.
2-beam & column approximations of the dynamical theory are used.
Euler's method is used for the integration along depth direction.
Length is in unit of angstrom.
Excitation error W is dimensionless.

***** parameters used for calculation *****

Reflection vector g = -2  2  0
Burgers vector    b = .5 -.5  0
Value of n = g·b  -2
Thickness of the specimen      500
Depth of the dislocation       250
Mean extinction distance              1000
Extinction distance for the reflection 1000
Mean absorption distance             20000
Absorption distance for the reflection 20000
Range of the excitation error W (minimum) -10
                                   (maximum)  10
Range of distance from the dislocation (minimum) -125
                                   (maximum)  125
Total number of calculation points along the excitation error axis  45
Total number of calculation points along the distance axis          79
Total number of slabs perpendicular to the depth direction          250

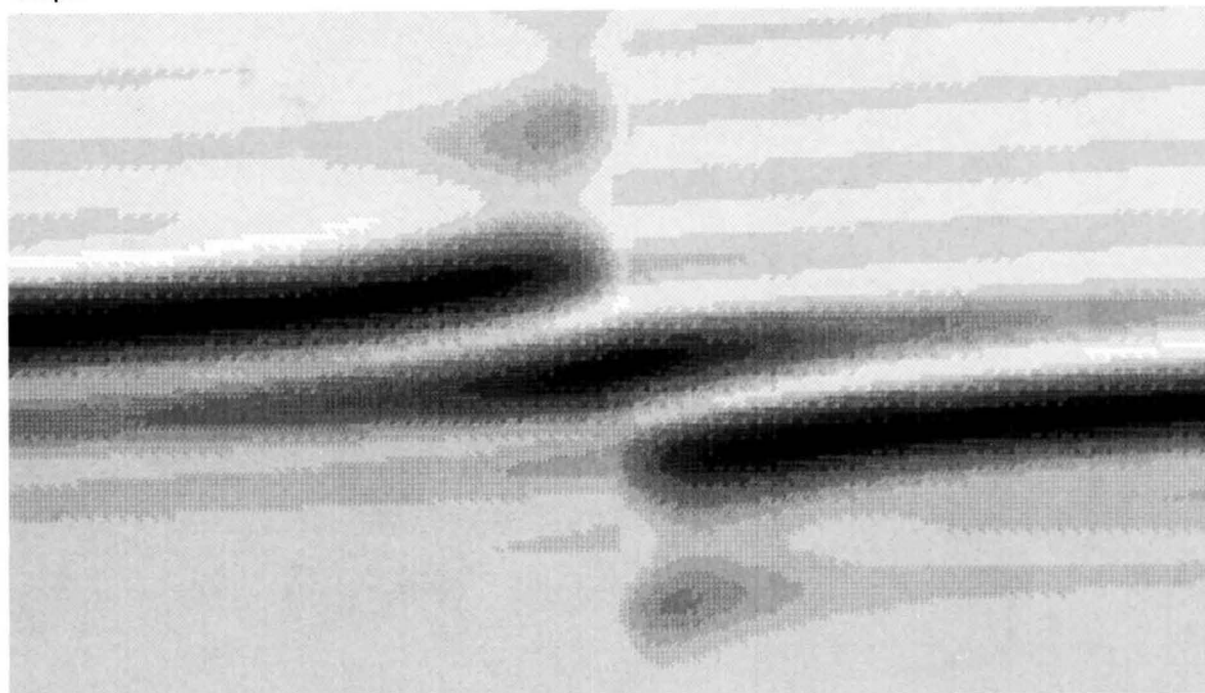
***** image processing data *****

magnification 3 times
2nd order interpolation

***** printing mode *****

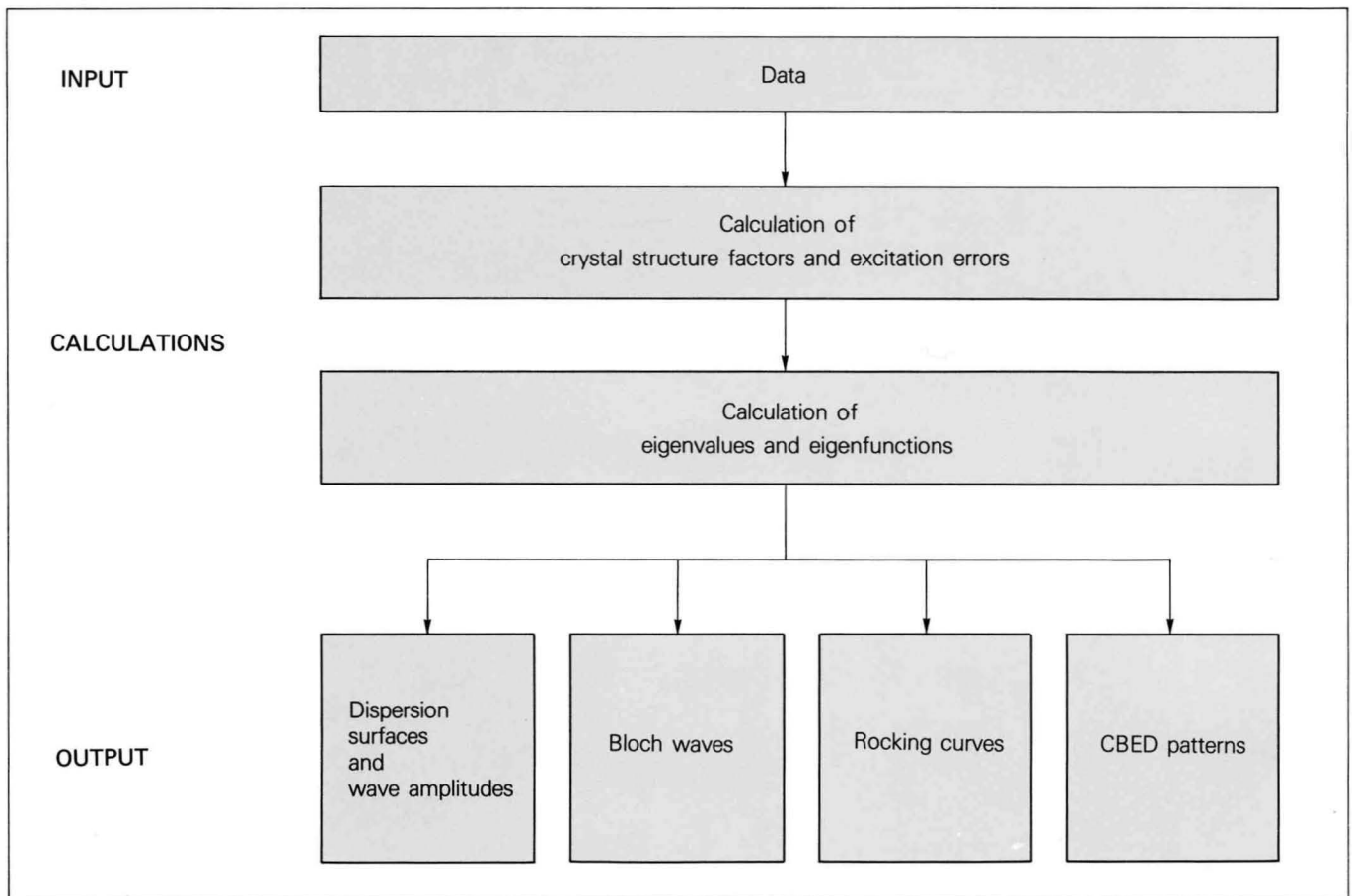
135 * 237 pixels / original : 45 * 79 pixels
background color : white
type 1 enhancement curve
```

## Output

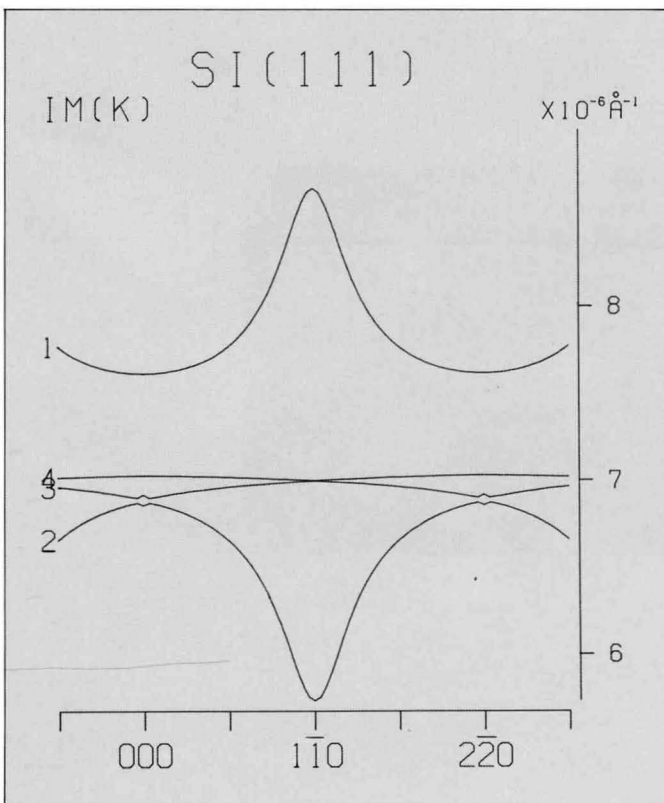
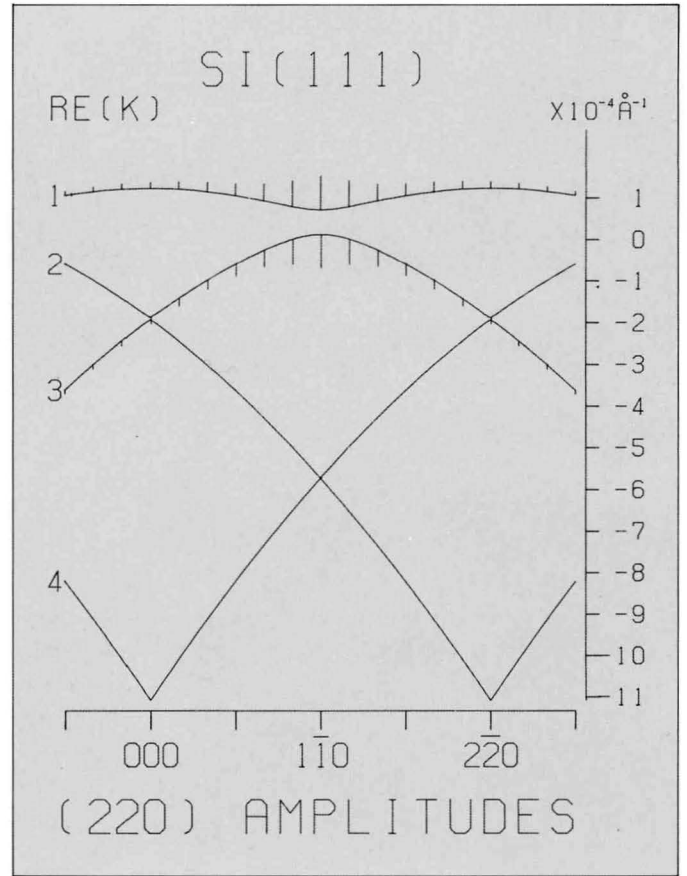
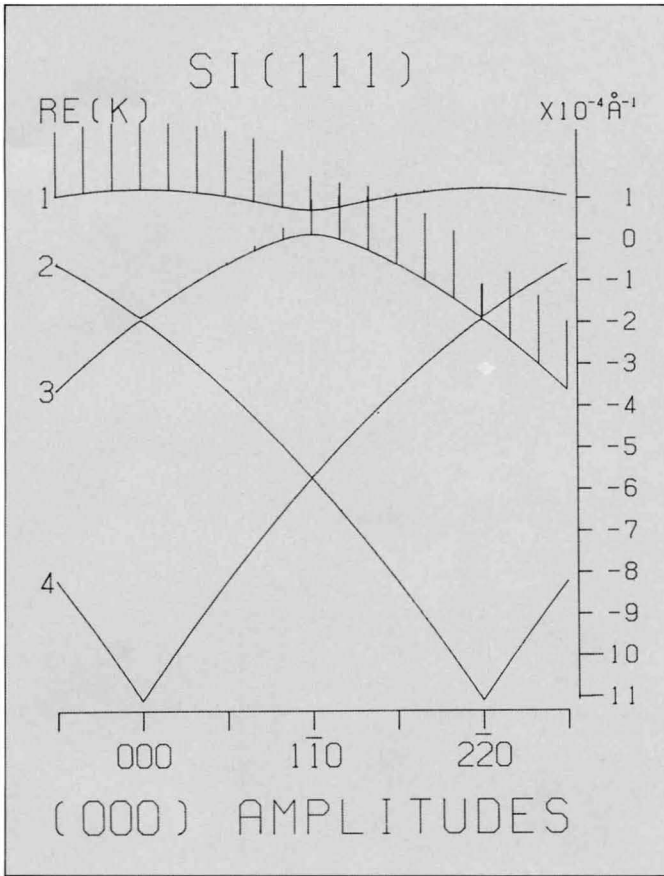


## Dynamical calculations

### Flow chart



**Dispersion surfaces and wave amplitudes**

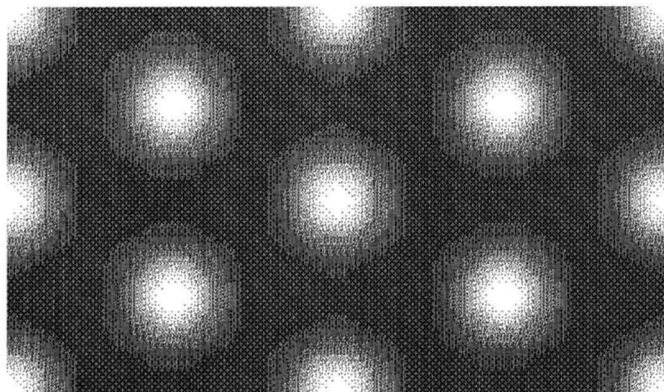
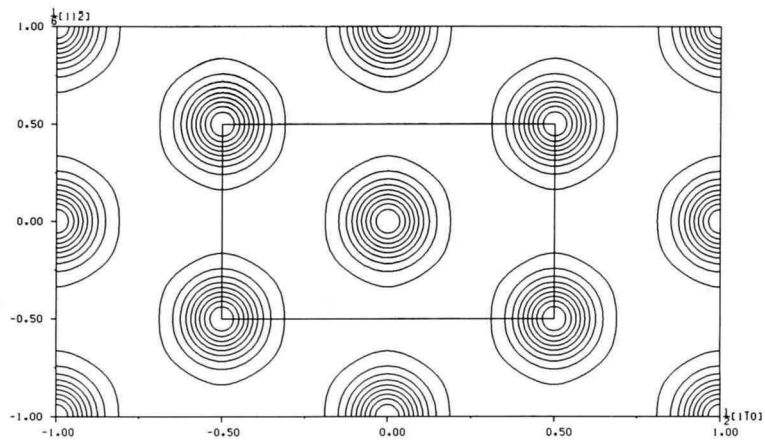
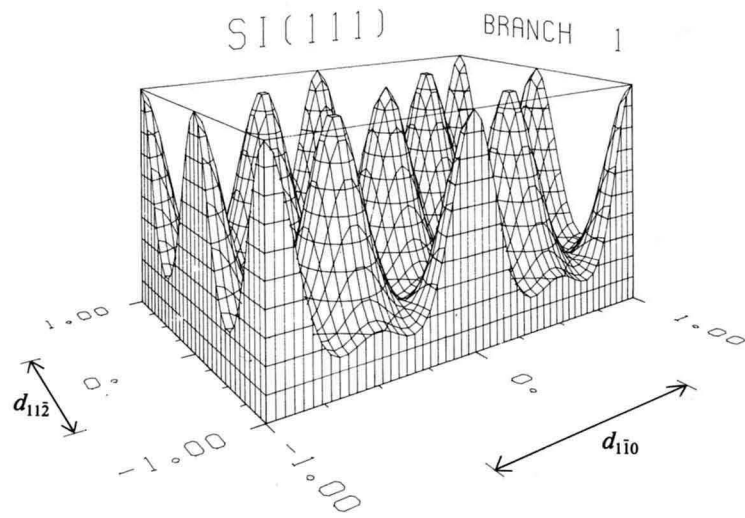


**Si [111]**

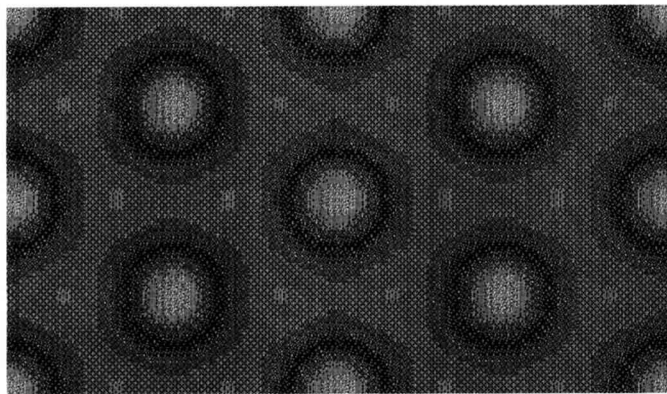
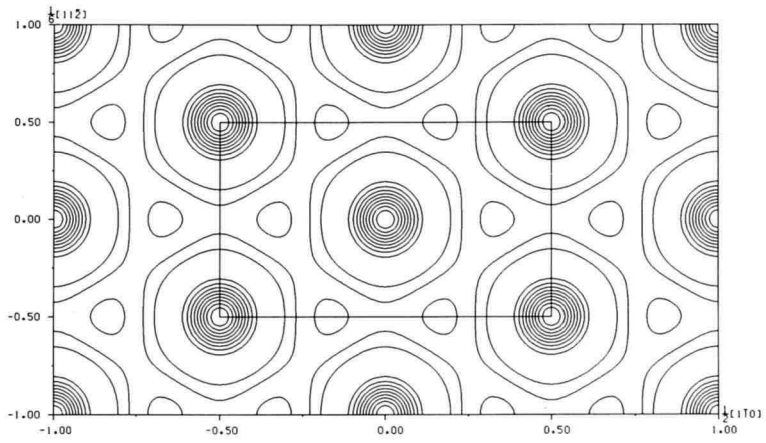
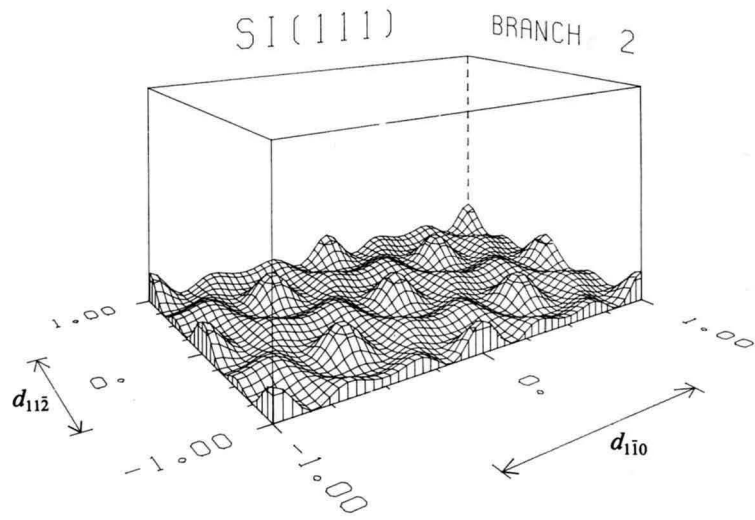
$2\bar{2}0$  excitation  
Accelerating voltage: 100kV  
 $h\bar{h}0$  systematic reflections: 10 beams  
Thickness: 156.0 nm  
Absorption:  $\frac{\xi_o}{\xi'_o} = \frac{1}{20}$ ,  $\frac{\xi_g}{\xi'_g} = \frac{1}{20}$

**Bloch waves**

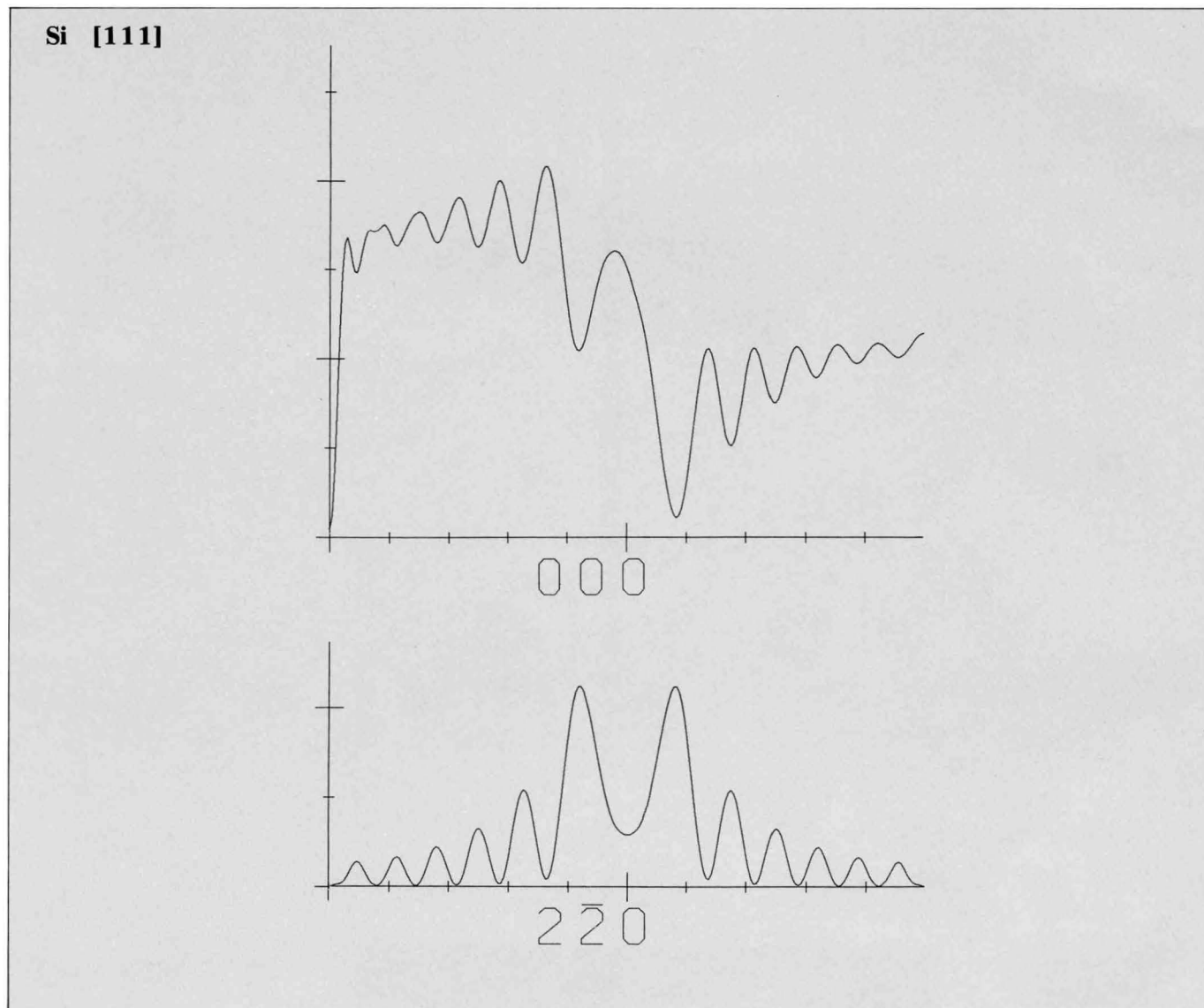
**Si [111]**



Zone-axis incidence  
 Accelerating voltage: 100kV  
 19 ZOLZ beams  
 Absorption:  $\frac{\xi_o}{\xi'_o} = \frac{1}{20}, \frac{\xi_g}{\xi'_g} = \frac{1}{20}$



## Rocking curves



$2\bar{2}0$  excitation

Accelerating voltage: 100kV

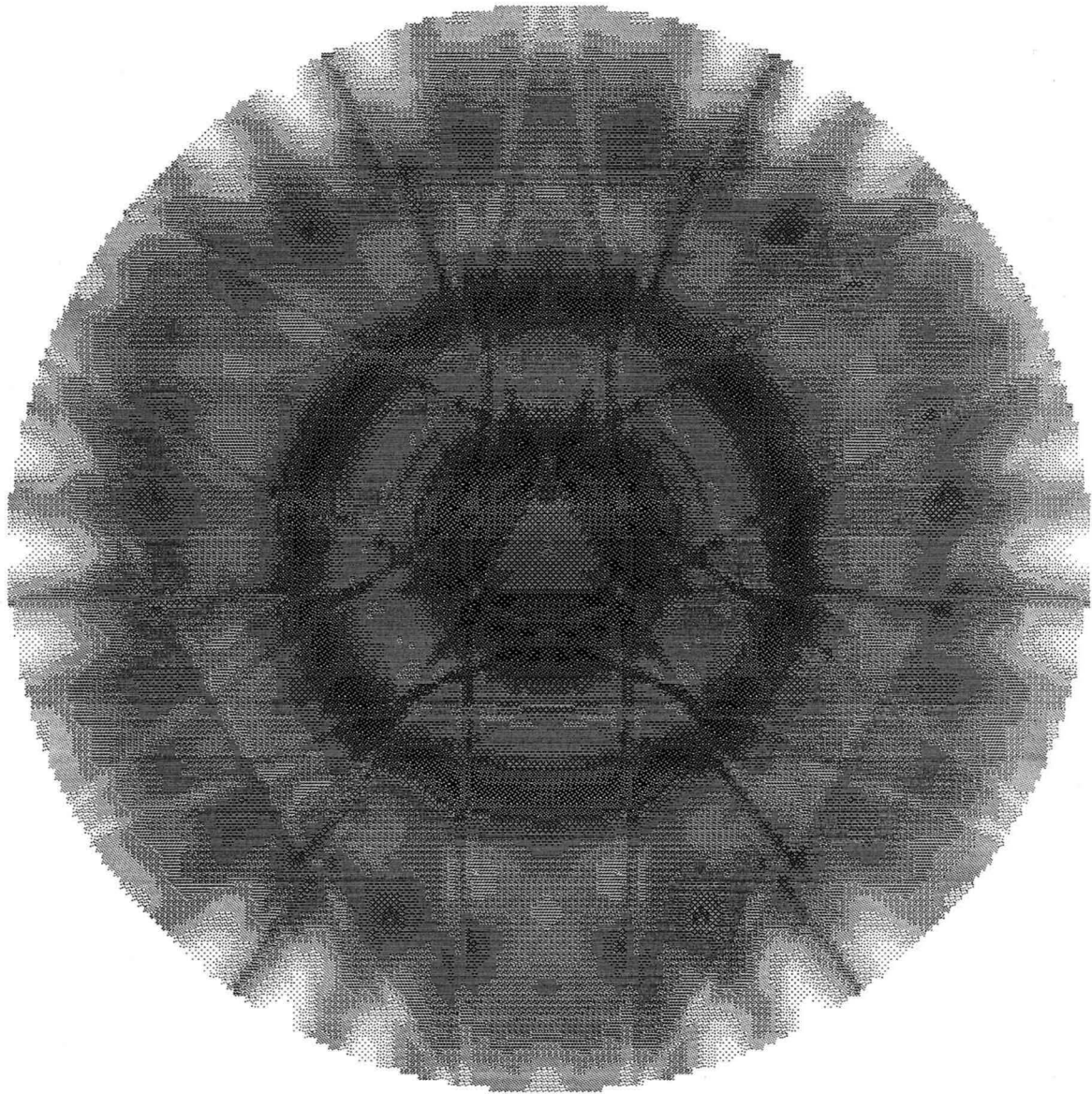
$h\bar{h}0$  systematic reflections: 10 beams

Thickness: 156.0 nm

Absorption:  $\frac{\xi_g}{\xi'_g} = \frac{1}{20}$

**CBED pattern**

**Si [111], 000 disk**



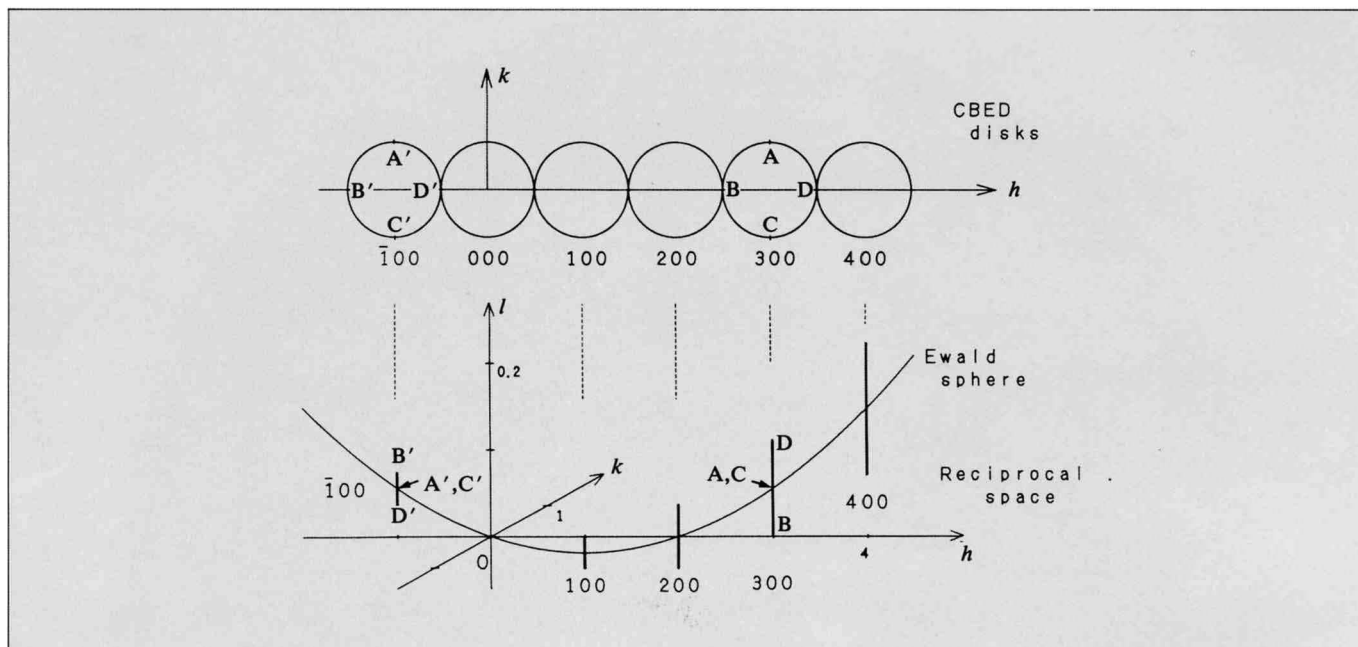
Zone-axis incidence  
Accelerating voltage: 100kV  
19 ZOLZ and 11 HOLZ beams  
Thickness: 156.0 nm  
Absorption:  $\frac{\xi_g}{\xi'_g} = \frac{1}{20}$

181 \* 181 pixels  
type 3 enhancement curve / gamma-coef. = .5

# Reciprocal-Space Lines Corresponding to CBED Disks

The larger the reflection index, the longer the reciprocal-space line projected in the corresponding disk. In the disk, the excitation error changes along the direction of the reflection vector (direction  $h$  in the present figure) and

remains the same along the direction perpendicular to the reflection vector (direction  $k$ ). Everywhere in the bright-field disk, the excitation error is zero.



## Elimination of Specimen Contamination

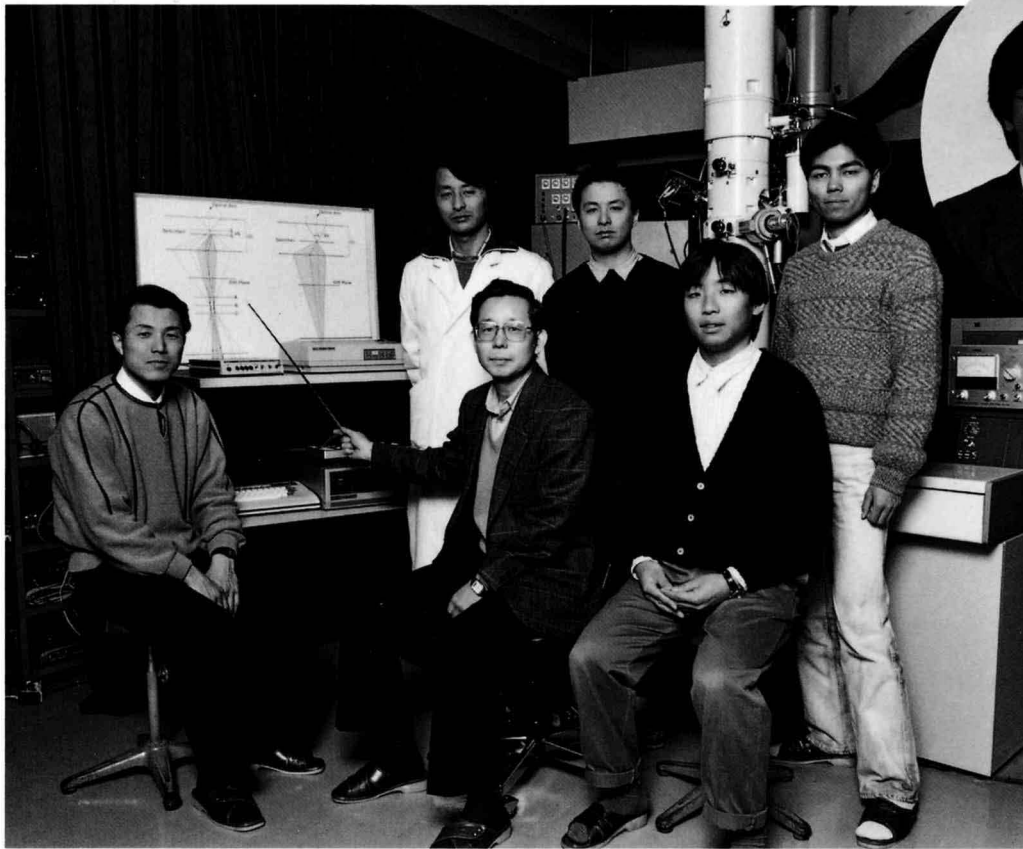
Today's electron microscopes are usually equipped with a dry evacuation system and have a clean vacuum of better than  $6 \times 10^{-5}$  Pa. The amount of dirt coming directly from the microscope itself is less important than before, as long as an anticontamination trap for specimens is used.

Specimen contamination occurs due to the surface migration and pile-up of previously stuck hydrocarbons and other types of dirt towards the area illuminated by the electron beam. Thus, preparation of clean specimens is needed above all things. However, we often encounter the need to observe insufficiently clean specimens. Practical elimination of specimen contamination is carried out in the following ways:

- 1) When the specimen is observed at about  $150^\circ\text{C}$  using a specimen heating stage, contamination decreases due to the desorption of stuck molecules.
- 2) When the specimen is observed at the  $\text{Liq. N}_2$  temperature using a specimen cooling stage, contamination also decreases due to the suppression of surface migration of dirt.

However, observation is not always possible at high and low temperatures, since it must often be conducted at varying temperatures.

- 3) The most practical and convenient technique to eliminate contamination is the use of a beam shower. When an indication of contamination is noticed during observation, strong electron illumination should be given for more than 5 minutes by removing the condenser aperture. Contamination is then definitely reduced.
- 4) Contamination is more reliably reduced by a technique of heating the specimen up to  $150^\circ\text{C}$  for about half an hour on a furnace in a vacuum evaporation device. This is the best way known by us at present.
- 5) Another possible technique is the slight etching of the surfaces by sputtering light ions of He at a low accelerating voltage of about 500 V for a few minutes, using an ion sputtering device for SEM specimen preparation.



T. Kaneyama

F. Sato

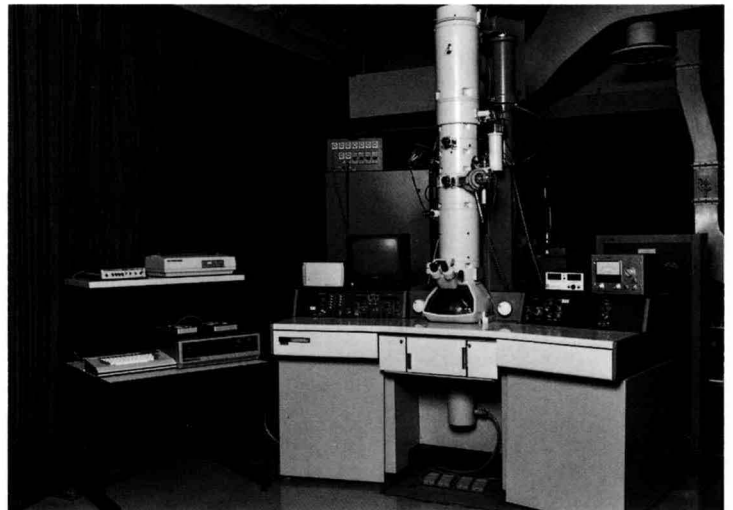
M. Terauchi

A. Ishikawa

S. Ito

M. Tanaka

K. Tsuda



JEM-2000 FX with TV system